

**NOVRAM\* Data Sheets**

**1**

**Serial I/O Data Sheets**

**2**

**E<sup>2</sup>PROM Data Sheets**

**3**

**E<sup>2</sup>POT™ Digitally Controlled  
Potentiometer Data Sheets**

**4**

**Die Products**

**5**

**Military**

**6**

**Applications**

**7**

**Reliability**

**8**

**General Information**

**9**





# DATA BOOK

## *President's Message*

Dear Customer:

As the leader of the exciting field of E<sup>2</sup>PROM and NOVRAM memories, Xicor has charted a course to provide an extensive product offering to cover the needs of your company in the field-reprogrammable nonvolatile area. This catalog contains data sheets for E<sup>2</sup>PROMs, NOVRAMs, and the revolutionary E<sup>2</sup>POT potentiometers. These products are typically available in a wide variety of speeds, package types and both parallel and serial interface configurations. The majority of the products are offered with extended temperature range, and many comply with all the requirements of Mil-Std-883 Revision C for Class B products. This catalog also contains advanced data sheets of various products under development, as well as numerous reliability reports and application notes.

To date, Xicor has shipped close to 30 million E<sup>2</sup>PROM and NOVRAM memories to its customers. Our research and development activities are substantial and will enable us to continue to introduce innovative products. Our worldwide sales, marketing and applications organizations are dedicated to supporting your requirements. We appreciate your business and look forward to supplying your present and future requirements.

A handwritten signature in black ink, appearing to read "R. Klein", with a long, sweeping horizontal stroke extending to the right.

Raphael Klein  
President  
September, 1987

Second Edition  
First Printing  
Printed in U.S.A.  
© XICOR, INC., 1987  
"All Rights Reserved"



---

**Fact Sheets** contain information on products under development. Xicor reserves the right to change these specifications or modify the product at any time, without notice.

**Advanced Data Sheets** contain typical product specifications which are subject to change upon device characterization over the full specified temperature range. Xicor reserves the right to change these specifications or modify the product at any time, without notice.

**Preliminary Data Sheets** contain minimum and maximum limits specified over the full temperature range based upon initial production device characterization. Xicor reserves the right to change these specifications or modify the product at any time, without notice.

**Final Data Sheets** contain minimum and maximum limits specified over the full temperature range for production devices.

Contact your local Xicor sales representative to obtain the latest specifications prior to order placement.

**Xicor** and Xicor is a trademark of Xicor, Inc.

E<sup>2</sup>POT™ is a trademark of Xicor, Inc.

NOVRAM is Xicor's nonvolatile static RAM device.

COPST™ is a trademark of National Semiconductor Corp.

---

#### LIMITED WARRANTY

Devices sold by Xicor, Inc. are covered by the warranty and patent indemnification provisions appearing in its Terms of Sale only. Xicor, Inc. makes no warranty, express, statutory, implied, or by description regarding the information set forth herein or regarding the freedom of the described devices from patent infringement. Xicor, Inc. makes no warranty of merchantability or fitness for any purpose. Xicor, Inc. reserves the right to discontinue production and change specifications and prices at any time and without notice.

Xicor, Inc. assumes no responsibility for the use of any circuitry other than circuitry embodied in a Xicor, Inc. product. No other circuits, patents, licenses are implied.

#### U.S. PATENTS

Xicor products are covered by one or more of the following U.S. Patents: 4,263,664; 4,274,012; 4,300,212; 4,314,265; 4,326,134; 4,393,481; 4,404,475; 4,450,402; 4,486,769; 4,488,060; 4,520,461; 4,533,846; 4,599,706; 4,617,652; 4,668,932. Foreign patents and additional patents pending.

#### LIFE RELATED POLICY

In situations where semiconductor component failure may endanger life, system designers using this product should design the system with appropriate error detection and correction, redundancy and back-up features to prevent such an occurrence.

Xicor's products are not authorized for use as critical components in life support devices or systems.

1. Life support devices or systems are devices or systems which, (a) are intended for surgical implant into the body, or (b) support or sustain life, and whose failure to perform, when properly used in accordance with instructions for use provided in the labeling, can be reasonably expected to result in a significant injury to the user.
  2. A critical component is any component of a life support device or system whose failure to perform can be reasonably expected to cause the failure of the life support device or system, or to affect its safety or effectiveness.
-

# Precautions for the Handling of MOS Devices

---

Xicor products are designed with effective input protection to prevent damage to the devices under most conditions. However, any MOS circuit can be catastrophically damaged by excessive electrostatic discharge or transient voltages. The following procedures are recommended to avoid accidental circuit damage.

## I. Testing MOS Circuits:

1. All units should be handled directly from the conductive or antistatic plastic tube in which they were shipped if possible. This action minimizes touching of individual leads.
2. If units are to be tested without using the tube carrier, the following precautions should be taken:
  - a. Table surfaces which potentially will come in contact with the devices either directly or indirectly (such as through shipping tubes) must be metal or of another conductive material and should be electrically connected to the test equipment and to the test operator (a grounding bracelet is recommended).
  - b. The units should be transported in bundled antistatic tubes or metal trays, both of which will assume a common potential when placed on a conductive table top.
  - c. Do not band tubes together with adhesive tape or rubber bands without first wrapping them in a conductive layer.

## II. Test Equipment (Including Environmental Equipment):

1. All equipment must be properly returned to the same reference potential (ground) as the devices, the operator, and the container for the devices.
2. Devices to be tested should be protected from high voltage surges developed by:
  - a. Turning electrical equipment on or off.
  - b. Relay switching.
  - c. Transients from voltage sources (AC line or power supplies).

## III. Assembling MOS Devices Onto PC Boards:

1. The MOS circuits should be mounted on the PC board last.
2. Similar precautions should be taken as in Item I above, at the assembly work station.
3. Soldering irons or solder baths should be at the same reference (ground) potential as the devices.
4. Plastic materials which are not antistatic treated should be kept away from devices as they develop and maintain high levels of static charge.

## IV. Device Handling:

1. Handling of devices should be kept to a minimum. If handling is required, avoid touching the leads directly.

## V. General:

1. The handler should take every precaution that the device will see the same reference potential when moved.
2. Anyone handling individual devices should develop a habit of first touching the container in which the units are stored before touching the units.
3. Before placing the units into a PC board, the handler should touch the PC board first.
4. Personnel should not wear clothing which will build up static charge. They should wear smocks and clothing made of 100% cotton rather than wool or synthetic fibers.
5. Be careful of electrostatic build up through the movement of air over plastic material. This is especially true of acid sinks.
6. Personnel or operators should always wear grounded wrist straps when working with MOS devices.
7. A 1 meg ohm resistance ground strap is recommended and will protect people up to 5,000 volts AC RMS or DC by limiting current to 5 milliamperes.
8. Antistatic ionized air equipment is very effective and useful in preventing electrostatic damage.
9. Low humidity maximizes potential static problems. Maintaining humidity levels above 45% is one of the most effective ways to guard against static handling problems.

## Product Index

---

This index includes all devices in Xicor nonvolatile memory product lines.

<b>Device No.</b>	<b>Description</b>	<b>Page No.</b>
X2201A	1024 x 1 NOVRAM .....	1-1
X2210, X2210I	64 x 4 NOVRAM .....	1-9
X2210M	64 x 4 NOVRAM Military Temperature Range .....	1-17
X2212, X2212I	256 x 4 NOVRAM .....	1-25
X2212M	256 x 4 NOVRAM Military Temperature Range .....	1-33
X2001, X2001I	128 x 8 NOVRAM .....	1-41
X2004, X2004I	512 x 8 NOVRAM .....	1-51
X2004M	512 x 8 NOVRAM Military Temperature Range .....	1-61
X2444, X2444I	16 x 16 Serial NOVRAM .....	2-1
X2444M	16 x 16 Serial NOVRAM Military Temperature Range .....	2-11
X2402, X2402I	256 x 8 Serial E <sup>2</sup> PROM .....	2-21
X2404, X2404I	512 x 8 Serial E <sup>2</sup> PROM .....	2-31
X2404M	512 x 8 Serial E <sup>2</sup> PROM Military Temperature Range .....	2-41
X24C04, X24C04I	512 x 8 CMOS Serial E <sup>2</sup> PROM .....	2-51
X24C16, X24C16I	2048 x 8 CMOS Serial E <sup>2</sup> PROM .....	2-61
X24C16M	2048 x 8 CMOS Serial E <sup>2</sup> PROM Military Temperature Range .....	2-71
X2804A, X2804AI	512 x 8 E <sup>2</sup> PROM .....	3-1
X2804AM	512 x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-9
X2816A, X2816AI	2K x 8 E <sup>2</sup> PROM .....	3-19
X2816AM	2K x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-27
X2816B, X2816BI	2K x 8 E <sup>2</sup> PROM .....	3-35
X2816BM	2K x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-45
X2864A, X2864AI	8K x 8 E <sup>2</sup> PROM .....	3-57
X2864AM	8K x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-67
X2864AT	8K x 8 E <sup>2</sup> PROM .....	3-79
X2864B, X2864BI	8K x 8 E <sup>2</sup> PROM .....	3-89
X2864BM	8K x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-97
X2864H, X2864HI	8K x 8 E <sup>2</sup> PROM .....	3-105
X2864HM	8K x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-113
X28256, X28256I	32K x 8 E <sup>2</sup> PROM .....	3-121
X28256M	32K x 8 E <sup>2</sup> PROM Military Temperature Range .....	3-135
X28C256, X28C256I	32K x 8 CMOS E <sup>2</sup> PROM .....	3-149
X28C256M	32K x 8 CMOS E <sup>2</sup> PROM Military Temperature Range .....	3-163
X28C010	128K x 8 E <sup>2</sup> PROM .....	3-177
X9MME, X9MMEI	E <sup>2</sup> POT <sup>TM</sup> Digitally Controlled Potentiometer .....	4-1
X9MMEM	E <sup>2</sup> POT <sup>TM</sup> Digitally Controlled Potentiometer Military Temperature Range .....	4-7





# Reference Guide to Xicor Nonvolatile Memories

## NOVRAMs\*

Part Number	Organization	Access Time	Power		Store Cycles	No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.
			Active	Standby				P	J	D	E	G	C		
X2201A	1024 x 1	300 ns	60 mA	N/A	10,000	18	†			•				1-1	9-1
X2210	64 x 4	300 ns	50 mA	N/A	10,000	18	†	•	•					1-9	9-1
X2210/5	64 x 4	300 ns	50 mA	N/A	10,000	18	†	•	•					1-9	9-1
X2210/10	64 x 4	300 ns	50 mA	N/A	10,000	18	†	•	•					1-9	9-1
X2210I	64 x 4	300 ns	55 mA	N/A	10,000	18	I	•	•					1-9	9-1
X2210I/5	64 x 4	300 ns	55 mA	N/A	10,000	18	I	•	•					1-9	9-1
X2210I/10	64 x 4	300 ns	55 mA	N/A	10,000	18	I	•	•					1-9	9-1
X2210M	64 x 4	300 ns	55 mA	N/A	10,000	18	M		•					1-17	9-1
X2210M/5	256 x 4	300 ns	55 mA	N/A	10,000	18	M		•					1-17	9-1
X2210M/10	256 x 4	300 ns	55 mA	N/A	10,000	18	M		•					1-17	9-1
X2212	256 x 4	300 ns	60 mA	N/A	10,000	18	†	•	•					1-25	9-2
X2212/5	256 x 4	300 ns	60 mA	N/A	10,000	18	†	•	•					1-25	9-1
X2212/10	256 x 4	300 ns	60 mA	N/A	10,000	18	†	•	•					1-25	9-1
X2212I	256 x 4	300 ns	70 mA	N/A	10,000	18	I	•	•					1-25	9-2
X2212I/5	256 x 4	300 ns	70 mA	N/A	10,000	18	I	•	•					1-25	9-2
X2212I/10	256 x 4	300 ns	70 mA	N/A	10,000	18	I	•	•					1-25	9-2
X2212M	256 x 4	300 ns	70 mA	N/A	10,000	18	M		•					1-33	9-2
X2212M/5	256 x 4	300 ns	70 mA	N/A	10,000	18	M		•					1-33	9-2
X2212M/10	256 x 4	300 ns	70 mA	N/A	10,000	18	M		•					1-33	9-2

N/A = Not Applicable

### Key:

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

\*NOVRAM is Xicor's nonvolatile static RAM device.

# Reference Guide to Xicor Nonvolatile Memories

## NOVRAMs (Byte-Wide)

Part Number	Organization	Access Time	Power		Store Cycles	No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.	
			Active	Standby				P	J	D	E	G	C			
X2001-20	128 x 8	200 ns	80 mA	50 mA	100,000	24	†	•		•					1-41	9-3
X2001-25	128 x 8	250 ns	80 mA	50 mA	100,000	24	†	•		•					1-41	9-3
X2001	128 x 8	300 ns	80 mA	50 mA	100,000	24	†	•		•					1-41	9-3
X2001I-20	128 x 8	200 ns	100 mA	65 mA	100,000	24	I	•		•					1-41	9-3
X2001I-25	128 x 8	250 ns	100 mA	65 mA	100,000	24	I	•		•					1-41	9-3
X2001I	128 x 8	300 ns	100 mA	65 mA	100,000	24	I	•		•					1-41	9-3
X2004-20	512 x 8	200 ns	100 mA	55 mA	100,000	28	†		•	•	•				1-51	9-3
X2004-25	512 x 8	250 ns	100 mA	55 mA	100,000	28	†		•	•	•				1-51	9-3
X2004	512 x 8	300 ns	100 mA	55 mA	100,000	28	†		•	•	•				1-51	9-3
X2004I-20	512 x 8	200 ns	120 mA	90 mA	100,000	28	I		•	•	•				1-51	9-3
X2004I-25	512 x 8	250 ns	120 mA	90 mA	100,000	28	I		•	•	•				1-51	9-3
X2004I	512 x 8	300 ns	120 mA	90 mA	100,000	28	I		•	•	•				1-51	9-3
X2004M-20	512 x 8	200 ns	120 mA	90 mA	100,000	28	M			•	•				1-61	9-3
X2004M-25	512 x 8	250 ns	120 mA	90 mA	100,000	28	M			•	•				1-61	9-3
X2004M	512 x 8	300 ns	120 mA	90 mA	100,000	28	M			•	•				1-61	9-3

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## SERIAL NOVRAMS

Part Number	Organization	CLK Frequency	Power			Store Cycles	No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.	
			Active	Standby	Sleep				P	J	D	E	G	C			
X2444	16 x 16	1 MHz	15 mA	10 mA	7 mA	100,000	8	†	•							2-1	9-5
X2444I	16 x 16	1 MHz	25 mA	15 mA	10 mA	100,000	8	I	•							2-1	9-5
X2444M	16 x 16	1 MHz	25 mA	15 mA	10 mA	100,000	8	M	•							2-11	9-5

## SERIAL E<sup>2</sup>PROMS

Part Number	Organization	Page Size (# Bytes)	CLK Frequency	Power		No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.	
				Active	Standby			P	J	D	E	G	C			
X2402	256 x 8	8	100 KHz	30 mA	25 mA	8	†	•							2-21	9-5
X2402I	256 x 8	8	100 KHz	35 mA	30 mA	8	I	•							2-21	9-5
X2404	512 x 8	8	100 KHz	30 mA	25 mA	8	†	•	•						2-31	9-5
X2404I	512 x 8	8	100 KHz	35 mA	30 mA	8	I	•	•						2-31	9-5
X2404M	512 x 8	8	100 KHz	35 mA	30 mA	8	M	•	•						2-41	9-5
X24C04	512 x 8	16	100 KHz	2 mA	60 $\mu$ A	8	†	•							2-51	9-5
X24C04I	512 x 8	16	100 KHz	2 mA	60 $\mu$ A	8	I	•							2-51	9-5
X24C16	2048 x 8	16	100 KHz	3 mA	75 $\mu$ A	8	†	•	•						2-61	9-5
X24C16I	2048 x 8	16	100 KHz	3 mA	75 $\mu$ A	8	I	•	•						2-61	9-5
X24C16M	2048 x 8	16	100 KHz	3 mA	75 $\mu$ A	8	M	•	•						2-71	9-5

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## 4K E<sup>2</sup>PROMs

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.
				Active	Standby			P	J	D	E	G		
X2804A-25	512 x 8	N/A	250 ns	80 mA	50 mA	24	†	•	•				3-1	9-6
X2804A	512 x 8	N/A	300 ns	80 mA	50 mA	24	†	•	•				3-1	9-6
X2804A-35	512 x 8	N/A	350 ns	80 mA	50 mA	24	†	•	•				3-1	9-6
X2804A-45	512 x 8	N/A	450 ns	80 mA	50 mA	24	†	•	•				3-1	9-6
X2804AI-25	512 x 8	N/A	250 ns	100 mA	60 mA	24	I	•	•				3-1	9-6
X2804AI	512 x 8	N/A	300 ns	100 mA	60 mA	24	I	•	•				3-1	9-6
X2804AI-35	512 x 8	N/A	350 ns	100 mA	60 mA	24	I	•	•				3-1	9-6
X2804AI-45	512 x 8	N/A	450 ns	100 mA	60 mA	24	I	•	•				3-1	9-6
X2804AM	512 x 8	N/A	300 ns	100 mA	60 mA	24	M	•	•				3-9	9-6
X2804AM-35	512 x 8	N/A	350 ns	100 mA	60 mA	24	M	•	•				3-9	9-6
X2804AM-45	512 x 8	N/A	450 ns	100 mA	60 mA	24	M	•	•				3-9	9-6

N/A = Not Applicable

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## 16K E<sup>2</sup>PROMs

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.
				Active	Standby			P	J	D	E	G		
X2816A-25	2048 x 8	N/A	250 ns	110 mA	50 mA	24	†	•	•	•			3-19	9-7
X2816A	2048 x 8	N/A	300 ns	110 mA	50 mA	24	†	•	•	•			3-19	9-7
X2816A-35	2048 x 8	N/A	350 ns	110 mA	50 mA	24	†	•	•	•			3-19	9-7
X2816A-45	2048 x 8	N/A	450 ns	110 mA	50 mA	24	†	•	•	•			3-19	9-7
X2816AI-25	2048 x 8	N/A	250 ns	140 mA	60 mA	24		•	•	•			3-19	9-7
X2816AI	2048 x 8	N/A	300 ns	140 mA	60 mA	24		•	•	•			3-19	9-7
X2816AI-35	2048 x 8	N/A	350 ns	140 mA	60 mA	24		•	•	•			3-19	9-7
X2816AI-45	2048 x 8	N/A	450 ns	140 mA	60 mA	24		•	•	•			3-19	9-7
X2816AM	2048 x 8	N/A	300 ns	140 mA	60 mA	24	M	•	•	•			3-27	9-7
X2816AM-35	2048 x 8	N/A	350 ns	140 mA	60 mA	24	M	•	•	•			3-27	9-7
X2816AM-45	2048 x 8	N/A	450 ns	140 mA	60 mA	24	M	•	•	•			3-27	9-7

## 16K E<sup>2</sup>PROMs (Continued)

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.
				Active	Standby			P	J	D	E	G		
X2816B-25	2048 x 8	16	250 ns	120 mA	60 mA	24	†	•	•	•	•		3-35	9-9
X2816B	2048 x 8	16	300 ns	120 mA	60 mA	24	†	•	•	•	•		3-35	9-9
X2816BI-25	2048 x 8	16	250 ns	120 mA	60 mA	24	†	•	•	•	•		3-35	9-9
X2816BI	2048 x 8	16	300 ns	140 mA	70 mA	24		•	•	•	•		3-35	9-9
X2816BM-25	2048 x 8	16	250 ns	140 mA	70 mA	24	M			•	•		3-45	9-9
X2816BM	2048 x 8	16	300 ns	140 mA	70 mA	24	M			•	•		3-45	9-9

N/A = Not Applicable

### Key:

† = Blank = Commercial = 0°C to +70°C

| = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## 64K E<sup>2</sup>PROMs

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.	
				Active	Standby			P	J	D	E	G	C			
X2864A-25	8192 x 8	16	250 ns	140 mA	60 mA	28	†	•	•	•	•				3-57	9-10
X2864A	8192 x 8	16	300 ns	140 mA	60 mA	28	†	•	•	•	•				3-57	9-10
X2864A-35	8192 x 8	16	350 ns	140 mA	60 mA	28	†	•	•	•	•				3-57	9-10
X2864A-45	8192 x 8	16	450 ns	140 mA	60 mA	28	†	•	•	•	•				3-57	9-10
X2864AI-25	8192 x 8	16	250 ns	140 mA	70 mA	28	I	•	•	•	•				3-57	9-10
X2864AI	8192 x 8	16	300 ns	140 mA	70 mA	28	I	•	•	•	•				3-57	9-10
X2864AI-35	8192 x 8	16	350 ns	140 mA	70 mA	28	I	•	•	•	•				3-57	9-10
X2864AI-45	8192 x 8	16	450 ns	140 mA	70 mA	28	I	•	•	•	•				3-57	9-10
X2864AM-25	8192 x 8	16	250 ns	140 mA	70 mA	28	M	•	•	•	•				3-67	9-10
X2864AM	8192 x 8	16	300 ns	140 mA	70 mA	28	M			•	•	•			3-67	9-10
X2864AM-35	8192 x 8	16	350 ns	140 mA	70 mA	28	M			•	•	•			3-67	9-10
X2864AM-45	8192 x 8	16	450 ns	140 mA	70 mA	28	M			•	•	•			3-67	9-10
X2864AT-35	8192 x 8	16	350 ns	110 mA	60 mA	28	T			•	•				3-79	9-12
X2864AT-45	8192 x 8	16	450 ns	110 mA	60 mA	28	T			•	•				3-79	9-12

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## 64K E<sup>2</sup>PROMs (Continued)

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.	
				Active	Standby			P	J	D	E	G			C
X2864B-120	8192 x 8	32	120 ns	150 mA	80 mA	28	†	•	•	•	•			3-89	9-12
X2864B-150	8192 x 8	32	150 ns	150 mA	80 mA	28	†	•	•	•	•			3-89	9-12
X2864B-180	8192 x 8	32	180 ns	150 mA	80 mA	28	†	•	•	•	•			3-89	9-12
X2864BI-120	8192 x 8	32	120 ns	150 mA	80 mA	28	I	•	•	•	•			3-89	9-12
X2864BI-150	8192 x 8	32	150 ns	150 mA	80 mA	28	I	•	•	•	•			3-89	9-12
X2864BI-180	8192 x 8	32	180 ns	150 mA	80 mA	28	I	•	•	•	•			3-89	9-12
X2864BM-120	8192 x 8	32	120 ns	150 mA	80 mA	28	M			•	•			3-97	9-13
X2864BM-150	8192 x 8	32	150 ns	150 mA	80 mA	28	M			•	•			3-97	9-13
X2864BM-180	8192 x 8	32	180 ns	150 mA	80 mA	28	M			•	•			3-97	9-13

## 64K E<sup>2</sup>PROMs (Continued)

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.	
				Active	Standby			P	J	D	E	G			C
X2864H-70	8192 x 8	32	70 ns	150 mA	80 mA	28	†	•	•	•	•			3-105	9-14
X2864H-90	8192 x 8	32	90 ns	150 mA	80 mA	28	†	•	•	•	•			3-105	9-14
X2864HI-90	8192 x 8	32	90 ns	150 mA	80 mA	28	I	•	•	•	•			3-105	9-14
X2864HM-90	8192 x 8	32	90 ns	150 mA	80 mA	28	M			•	•			3-113	9-14

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## 256K E<sup>2</sup>PROMs

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.	
				Active	Standby			P	J	D	E	G			C
X28256-25	32768 x 8	64	250 ns	120 mA	60 mA	28	†	•	•	•	•			3-121	9-15
X28256	32768 x 8	64	300 ns	120 mA	60 mA	28	†	•	•	•	•			3-121	9-15
X28256-35	32768 x 8	64	350 ns	120 mA	60 mA	28	†	•	•	•	•			3-121	9-15
X28256I-25	32768 x 8	64	250 ns	120 mA	60 mA	28	I	•	•	•	•			3-121	9-15
X28256I	32768 x 8	64	300 ns	120 mA	60 mA	28	I	•	•	•	•			3-121	9-15
X28256I-35	32768 x 8	64	350 ns	120 mA	60 mA	28	I	•	•	•	•			3-121	9-15
X28256M-25	32768 x 8	64	250 ns	120 mA	60 mA	28	M			•	•			3-135	9-15
X28256M	32768 x 8	64	300 ns	120 mA	60 mA	28	M			•	•			3-135	9-15
X28256M-35	32768 x 8	64	350 ns	120 mA	60 mA	28	M			•	•			3-135	9-15

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Ledged Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze



# Reference Guide to Xicor Nonvolatile Memories

## 256K E<sup>2</sup>PROMs (Continued)

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package					Data Sheet Page No.	Order Info. Page No.
				Active	Standby			P	J	D	E	G		
X28C256-25	32768 x 8	64	250 ns	60 mA	200 $\mu$ A	28	†	•	•	•	•		3-149	9-16
X28C256	32768 x 8	64	300 ns	60 mA	200 $\mu$ A	28	†	•	•	•	•		3-149	9-16
X28C256-35	32768 x 8	64	350 ns	60 mA	200 $\mu$ A	28	†	•	•	•	•		3-149	9-16
X28C256I-25	32768 x 8	64	250 ns	60 mA	200 $\mu$ A	28	I	•	•	•	•		3-149	9-16
X28C256I	32768 x 8	64	300 ns	60 mA	200 $\mu$ A	28	I	•	•	•	•		3-149	9-16
X28C256I-35	32768 x 8	64	350 ns	60 mA	200 $\mu$ A	28	I	•	•	•	•		3-149	9-16
X28C256M-25	32768 x 8	64	250 ns	60 mA	200 $\mu$ A	28	M			•	•		3-163	9-17
X28C256M	32768 x 8	64	300 ns	60 mA	200 $\mu$ A	28	M			•	•		3-163	9-17
X28C256M-35	32768 x 8	64	350 ns	60 mA	200 $\mu$ A	28	M			•	•		3-163	9-17

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

# Reference Guide to Xicor Nonvolatile Memories

## 1M E<sup>2</sup>PROMs

Part Number	Organization	Page Size (# Bytes)	Access Time	Power		No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.
				Active	Standby			P	J	D	E	G	C		
X28C010	131072 x 8	128	200 ns	80 mA	500 $\mu$ A	32	†, I, M			•			•	3-177	N/A

## E<sup>2</sup>POTENTIOMETERS

Part Number	Minimal Resistance	Wiper Increments	Maximum Resistance	No. of Pins	Temp. Range(s)	Package						Data Sheet Page No.	Order Info. Page No.
						P	J	D	E	G	C		
X9103	40 $\Omega$	101 $\Omega$	10 K $\Omega$	8	†, I, M	•						4-1, 4-7	9-18
X9503	40 $\Omega$	505 $\Omega$	50 K $\Omega$	8	†, I, M	•							9-18
X9104	40 $\Omega$	1010 $\Omega$	100 K $\Omega$	8	†, I, M	•							9-18

N/A = Not Applicable

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

## Table of Contents

---

### Section 1–NOVRAM Data Sheets

(See Product Index for sequence) . . . . . v

### Section 2–Serial I/O Data Sheets

(See Product Index for sequence) . . . . . v

### Section 3–E<sup>2</sup>PROM Data Sheets

(See Product Index for sequence) . . . . . v

### Section 4–E<sup>2</sup>POT™ Digitally Controlled Potentiometer Data Sheets

(See Product Index for sequence) . . . . . v

### Section 5–Die Products . . . . . 5-1

### Section 6–Military

Military 883 Program Overview . . . . . 6-1

### Section 7–Applications

#### Application Notes

- AN-101 Xicor NOVRAMs\* Easier Than Ever to Use . . . . . 7-1
- AN-103 Xicor Replaces DIP Switches and Trimmers with NOVRAM\* Memories . 7-9
- AN-105 The X2444 Serial NOVRAM\* Teams Up with the  
8051 Microcontroller Family . . . . . 7-17
- AN-106 E<sup>2</sup>POT™ Digitally Controlled Potentiometer Brings Microprocessor  
Control to Audio Systems–Adds Features . . . . . 7-23

#### Application Briefs

- The Nine Most Frequent NOVRAM\* Questions . . . . . 7-33
- Fourteen Common E<sup>2</sup>PROM Questions Answered . . . . . 7-37
- Nonvolatile Data Integrity: Inadvertent Write/Store Elimination . . . . . 7-41
- X2816A Design Allows Upgrade to X2864A and Beyond . . . . . 7-45
- Replacing DIP Switches with Nonvolatile Technology . . . . . 7-49
- Using  $\overline{\text{DATA}}$  Polling in an Interrupt Driven Environment . . . . . 7-53
- E<sup>2</sup>PROM Provides the Solution to Field Alterable Software . . . . . 7-57
- Xicor E<sup>2</sup>PROMs vs. Battery Backed-Up CMOS RAMs  
Nonvolatile Memory Systems . . . . . 7-61
- E<sup>2</sup>PROMs: The Competitive Edge Against Bubble Memories . . . . . 7-65
- “t<sub>DV</sub>”–What is it? . . . . . 7-69

---

\*NOVRAM is Xicor's nonvolatile static RAM device.

## Table of Contents

---

### Section 7—Applications (Continued)

#### Article Reprints

5-volt-only EE-PROM mimics static-RAM timing . . . . .	7-71
<i>Electronics, June 30, 1982</i>	
Understand your application in choosing NOVRAM, EEPROM . . . . .	7-77
<i>EDN, May 12, 1983</i>	
Non-volatile memories keep appliances out of the dark . . . . .	7-89
<i>Design News, October 1983</i>	
Nonvolatile Memory Gives New Life to Old Designs . . . . .	7-95
<i>Computer Design, October 1, 1984</i>	
Save volatile data during power loss . . . . .	7-103
<i>EDN, February 21, 1985</i>	
Thick Oxide Beats Thin Film in Building Big EEPROMs . . . . .	7-111
<i>Electronics, May 12, 1986</i>	
Solid-State Potentiometer . . . . .	7-115
<i>Machine Design, May 22, 1986</i>	
<b>Bit Maps for Xicor Products . . . . .</b>	<b>7-117</b>

### Section 8—Reliability

RR-502A NOVRAM* Reliability Report . . . . .	8-1
RR-504 Endurance of Xicor E <sup>2</sup> PROMs and NOVRAMs* . . . . .	8-23
RR-505 X2816A/X2804A Reliability Report . . . . .	8-33
RR-506 Byte-Wide NOVRAM* (X2001/X2004) Reliability Report . . . . .	8-45
RR-507A X2864A Reliability Report . . . . .	8-57
RR-508 X2404 Reliability Report . . . . .	8-71
RR-509 X2816B Reliability Report . . . . .	8-79
RR-510 Endurance of Nonvolatile Memories . . . . .	8-87
Determining System Reliability from E <sup>2</sup> PROM Endurance Data . . . . .	8-93
Radiation-Induced Soft Errors and Floating Gate Memories . . . . .	8-97
Endurance Model for Textured Poly Floating Gate Memories . . . . .	8-103
The Prediction of Textured Poly Floating Gate Memory Endurance . . . . .	8-109
Comparison and Trends in Today's Dominant E <sup>2</sup> Technologies . . . . .	8-117
New Ultra-High Density Textured Poly-Si Floating Gate E <sup>2</sup> PROM Cell . . . . .	8-123
Reliability Comparison of Flotex and Textured Poly E <sup>2</sup> PROMs . . . . .	8-125

### Section 9—General Information

Ordering Information . . . . .	9-1
Packaging Information . . . . .	9-19
Sales Offices . . . . .	9-32

## Memory Overview

---

Since its founding, Xicor has developed and placed into production a wide range of system-alterable nonvolatile memory devices. These devices, manufactured with Xicor's proprietary state-of-the-art textured triple-poly floating gate process, are available in a variety of architectures (NOVRAM\* and E<sup>2</sup>PROM), interfaces (nibble-wide, byte-wide and serial), densities, and speeds. Xicor's success as an innovator and leader in system-alterable nonvolatile memory is affirmed with an *Electronic Product Magazine* Product of the Year award in 1980 and again in 1982 for the first 5-volt only NOVRAM and the first 5-volt only full featured E<sup>2</sup>PROM, respectively.

Lower density E<sup>2</sup>PROMs and NOVRAMs have been readily available for a number of years and have provided unique niche applications solutions. Serial devices have replaced DIP switches in a wide range of products that offer user selectable operating parameters. Nibble-wide and byte-wide NOVRAMs and E<sup>2</sup>PROMs are being used in instrumentation and industrial control applications to store calibration data and control information. Communications equipment has implemented these same devices to store phone numbers in repertory dialers and antenna positioning equipment.

The list of first generation applications goes on at length; however, with the second generation represented by the X2864A, the direction of applications began to diverge. The higher density allowed practical usage of E<sup>2</sup>PROMs in program and mass data storage. The advent of the X28256 has pushed this application usage even higher.

Xicor strives to serve the marketplace by providing next generation devices in existing product areas as evidenced by the X2864B and X2864H high speed 64K E<sup>2</sup>PROMs. Similarly, the X24C16 and X24C04 maintain compatibility with the original X2404 but offer low power operation over a much wider  $V_{CC}$  range.

As designers have gained experience implementing the denser E<sup>2</sup>PROM devices into system memories, they have given Xicor feedback on features they would like. Xicor has listened.

Xicor's response has been active. The issues addressed by the Xicor design team have been: faster read access time, faster write cycle time, denser memory devices and write protection mechanisms.

Xicor has also implemented added features via software control rather than "dedicated pin" hardware control for optional system use. Xicor is committed to providing solutions that neither hinder nor limit the system designer's imagination. The products and features shown in the data sheets in this data book illustrate Xicor's dedication to listening to you, the designer, in providing memory design solutions.

---

\*NOVRAM is Xicor's nonvolatile static RAM device.



X2201A.....	1-1
X2210, X2210I.....	1-9
X2210M.....	1-17
X2212, X2212I.....	1-25
X2212M.....	1-33
X2001, X2001I.....	1-41
X2004, X2004I.....	1-51
X2004M.....	1-61



## NOVRAM\* Data Sheets





**Nonvolatile Static RAM**

1

**FEATURES**

- Single 5V Supply
- Fully TTL Compatible
- Infinite E<sup>2</sup>PROM Array Recall, RAM Read and Write Cycles
- Access Time of 300 ns Max.
- Nonvolatile Store Inhibit: V<sub>CC</sub> = 3V Typical
- 100 Year Data Retention

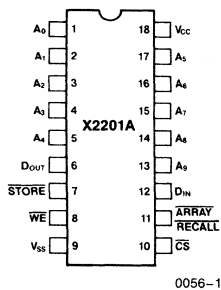
The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and from E<sup>2</sup>PROM to RAM (recall). The store operation is completed in 10 ms or less and the recall is typically completed in 1 μs.

**DESCRIPTION**

The Xicor X2201A is a 1024 x 1 NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile E<sup>2</sup>PROM. The X2201A is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V nonvolatile memories.

Xicor NOVRAMS are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM. The E<sup>2</sup>PROM array is designed for a minimum 10,000 store cycles. Data retention is specified to be greater than 100 years.

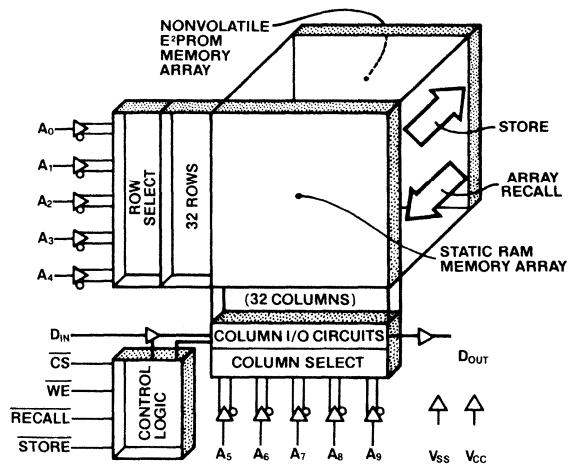
**PIN CONFIGURATION**



**PIN NAMES**

A <sub>0</sub> -A <sub>9</sub>	Address Inputs
D <sub>IN</sub>	Data Input
D <sub>OUT</sub>	Data Out
WE	Write Enable
CS	Chip Select
ARRAY RECALL	Array Recall
STORE	Store
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground

**FUNCTIONAL DIAGRAM**



0056-2

# X2201A

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias.....	-10°C to +85°C
Storage Temperature.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground.....	-1.0V to +7V
D.C. Output Current.....	5 mA
Lead Temperature (Soldering, 10 Seconds).....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	Power Supply Current		60	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0\text{ mA}$
$I_{LI}$	Input Load Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 4.2\text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -2\text{ mA}$

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0\text{ MHz}$ , $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

## MODE SELECTION

Inputs				Input Output I/O	Mode
CS	WE	ARRAY RECALL	STORE		
H	X	H	H	Output High Z	Not Selected <sup>(2)</sup>
L	H	H	H	Output Data	Read RAM
L	L	H	H	Input Data High	Write "1" RAM
L	L	H	H	Input Data Low	Write "0" RAM
X	H	L	H	Output High Z	Array Recall
H	X	L	H	Output High Z	Array Recall
X	H	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>
H	X	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>

**Notes:** (1) This parameter is periodically sampled and not 100% tested.

(2) Chip is deselected but may be automatically completing a store cycle.

(3) STORE = L is required only to initiate the store cycle, after which the store cycle will be automatically completed (STORE = X).

# X2201A

## A.C. CHARACTERISTICS

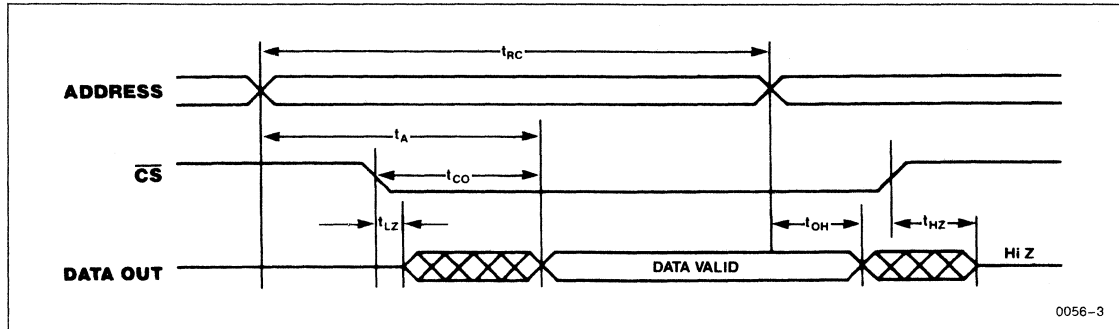
$T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

1

### Read Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RC}$	Read Cycle Time	300		ns
$t_A$	Access Time		300	ns
$t_{CO}$	Chip Select to Output Valid		200	ns
$t_{OH}$	Output Hold from Address Change	50		ns
$t_{LZ}$	Chip Select to Output in Low Z	10		ns
$t_{HZ}$	Chip Deselect to Output in High Z	10	100	ns

### Read Cycle

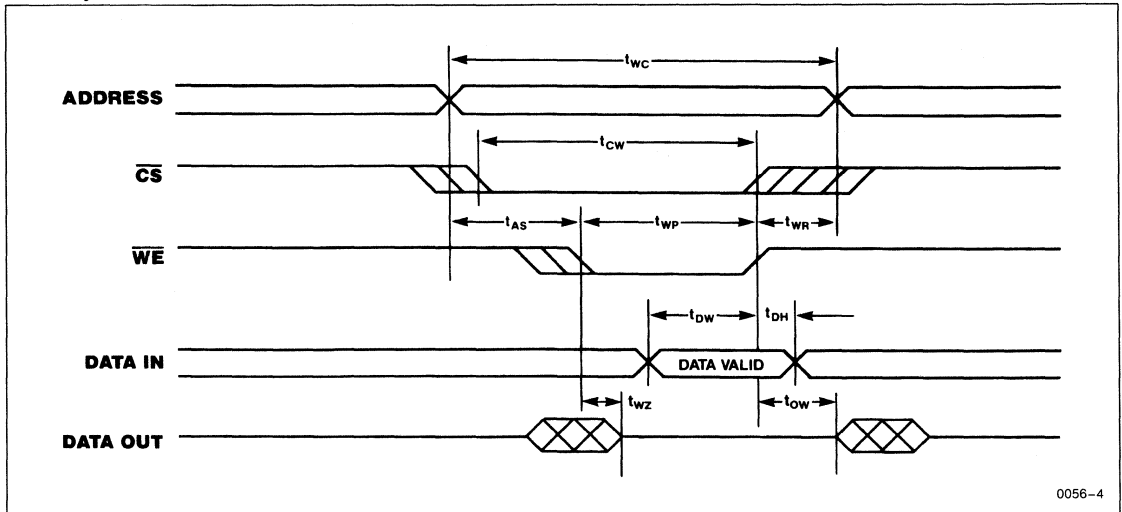


# X2201A

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	300		ns
$t_{CW}$	Chip Select to End of Write	150		ns
$t_{AS}$	Address Setup Time	50		ns
$t_{WP}$	Write Pulse Width	150		ns
$t_{WR}$	Write Recovery Time	25		ns
$t_{DW}$	Data Valid to End of Write	100		ns
$t_{DH}$	Data Hold Time	0		ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	ns
$t_{OW}$	Output Active from End of Write	10		ns

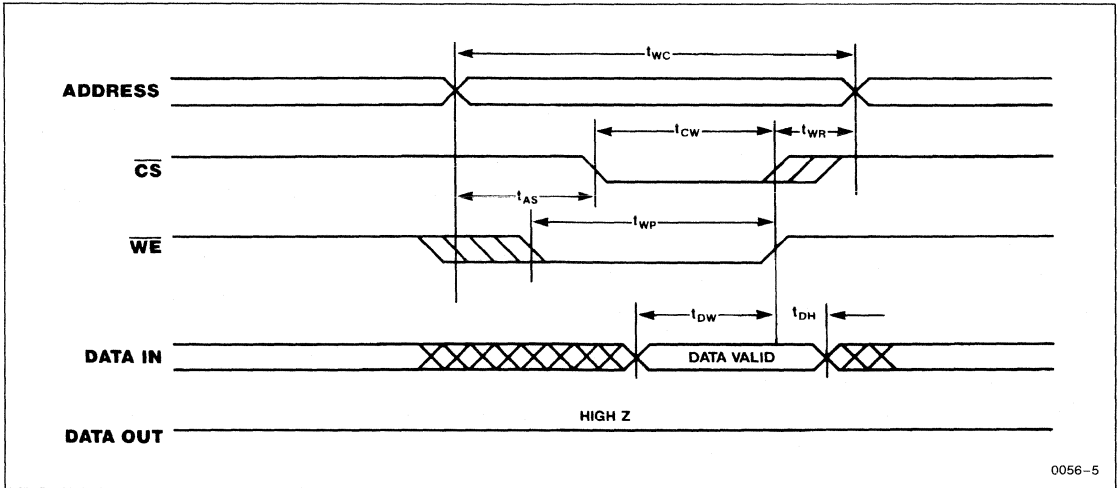
## Write Cycle



# X2201A

1

## Early Write Cycle

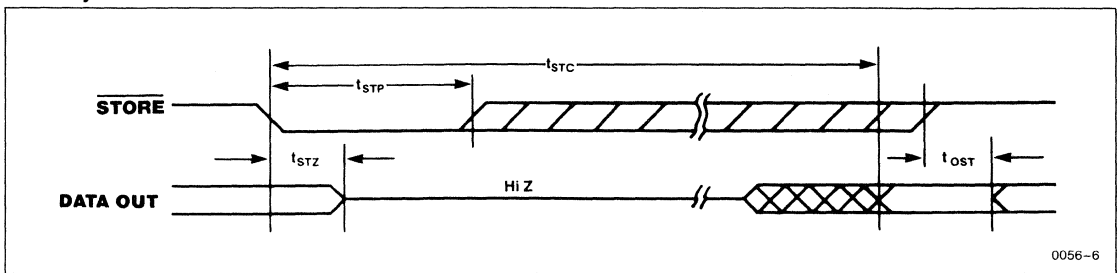


0056-5

## Store Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{STC}$	Store Cycle Time		10	ms
$t_{STP}$	Store Pulse Width	100		ns
$t_{STZ}$	Store to Output in High Z		500	ns
$t_{OST}$	Output Active from End of Store	10		ns

## Store Cycle



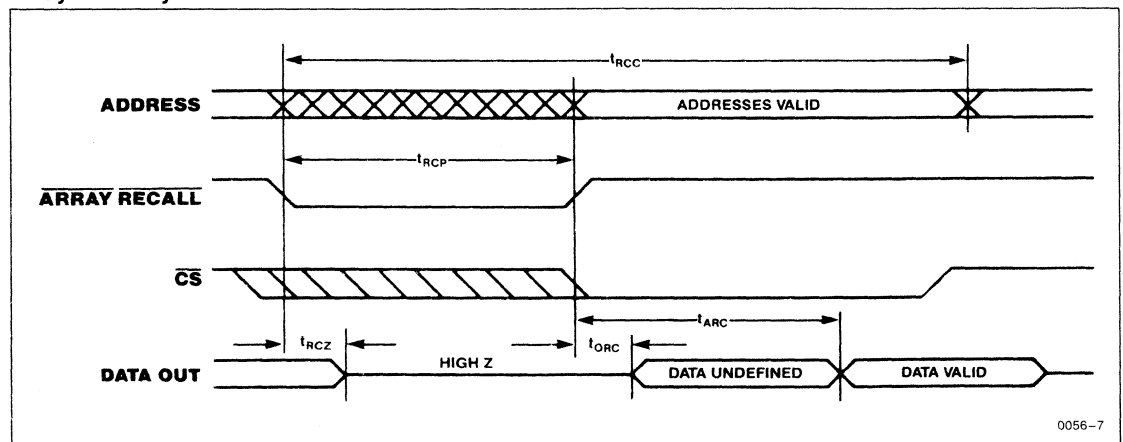
0056-6

# X2201A

## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RCC}$	Array Recall Cycle Time	1200		ns
$t_{RCP}$	Recall Pulse Width <sup>(4)</sup>	450		ns
$t_{RCZ}$	Recall to Output in High Z		150	ns
$t_{ORC}$	Output Active from End of Recall	10		ns
$t_{ARC}$	Recalled Data Access Time from End of Recall		750	ns

## Array Recall Cycle



**Note:** (4) Array Recall rise time must be less than 1  $\mu$ s.

# X2201A

1

## PIN DESCRIPTIONS AND DEVICE OPERATION

### Addresses (A<sub>0</sub>–A<sub>9</sub>)

The address inputs select a memory location during a read or write operation.

### Chip Select ( $\overline{CS}$ )

The Chip Select input must be LOW to enable read/write operations with the RAM array.  $\overline{CS}$  HIGH will place the D<sub>OUT</sub> in the high impedance state.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the D<sub>OUT</sub> buffer, determining whether a RAM read or write operation is enabled. WE HIGH enables a read and WE LOW enables a write.

### Data In (D<sub>IN</sub>)

Data is written into the device via the D<sub>IN</sub> input.

### Data Out (D<sub>OUT</sub>)

Data from a selected address is output on the D<sub>OUT</sub> output. This pin is in the high impedance state when either  $\overline{CS}$  is HIGH or when  $\overline{WE}$  is LOW.

### STORE

The STORE input, when LOW, will initiate the transfer of the entire contents of the RAM array to the E<sup>2</sup>PROM array. The  $\overline{WE}$  and  $\overline{ARRAY\ RECALL}$  inputs are inhibited during the store cycle. The store operation will be completed in 10 ms or less.

A store operation has priority over RAM read/write operations. If STORE is asserted during a read operation, the read will be discontinued. If  $\overline{STORE}$  is asserted during a RAM write operation, the write will be immediately terminated and the store performed. The data at the RAM address that was being written will be unknown in both the RAM and E<sup>2</sup>PROM.

### ARRAY RECALL

The ARRAY RECALL input, when LOW, will initiate the transfer of the entire contents of the E<sup>2</sup>PROM array to the RAM array. The transfer of data will typically be completed in 1 μs or less.

An array recall has priority over RAM read/write operations and will terminate both operations when  $\overline{ARRAY\ RECALL}$  is asserted.  $\overline{ARRAY\ RECALL}$  LOW will also inhibit the  $\overline{STORE}$  input.

### WRITE PROTECTION

The X2201A has three write protect features that are employed to protect the contents of the nonvolatile memory.

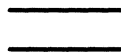




- V<sub>CC</sub> Sense—All functions are inhibited when V<sub>CC</sub> is ≤ 3V, typically.
- Write Inhibit—Holding either  $\overline{STORE}$  HIGH or  $\overline{ARRAY\ RECALL}$  LOW during power-up or power-down will prevent an inadvertent store operation and E<sup>2</sup>PROM data integrity will be maintained.
- Noise Protection—A STORE pulse of less than 20 ns will *not* initiate a store cycle.

## ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

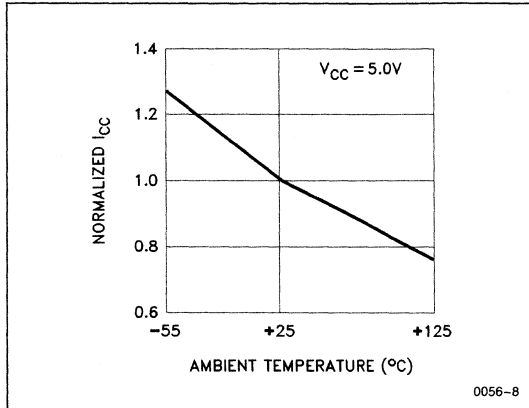
Part Number	Store Cycles	Data Changes Per Bit
X2201A	10,000	1,000

## SYMBOL TABLE

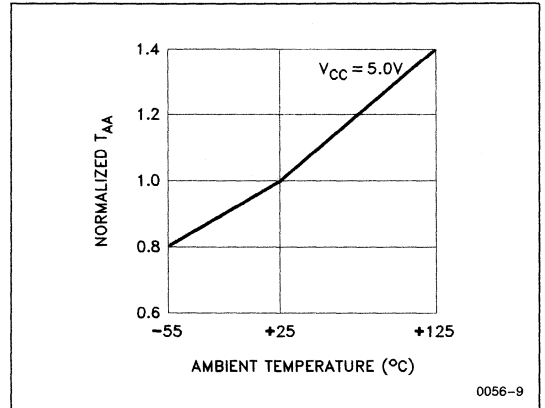
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2201A

**Normalized Active Supply Current  
vs. Ambient Temperature**



**Normalized Access Time  
vs. Ambient Temperature**





256 Bit      Commercial      X2210      64 x 4 Bit  
 Industrial      X2210I

## Nonvolatile Static RAM

1

### FEATURES

- Single 5V Supply
- Fully TTL Compatible
- Infinite E<sup>2</sup>PROM Array Recall, RAM Read and Write Cycles
- Access Time of 300 ns Max.
- Nonvolatile Store Inhibit: V<sub>CC</sub> = 3V Typical
- 100 Year Data Retention
- JEDEC Standard 18-Pin Package

### DESCRIPTION

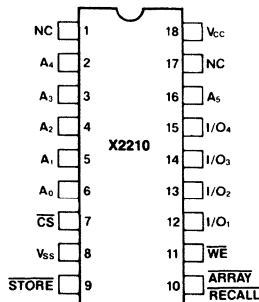
The Xicor X2210 is a 64 x 4 NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile E<sup>2</sup>PROM. The X2210 is fabricated with the same reliable N-channel floating gate MOS technology used

in all Xicor 5V nonvolatile memories. The X2210 features the JEDEC approved pinout for 4-bit-wide memories, compatible with industry standard RAMs.

The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and from E<sup>2</sup>PROM to RAM (recall). The store operation is completed in 10 ms or less and the recall is typically completed in 1 μs.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM. The E<sup>2</sup>PROM array is designed for a minimum 10,000 store cycles. Data retention is specified to be greater than 100 years.

### PIN CONFIGURATION

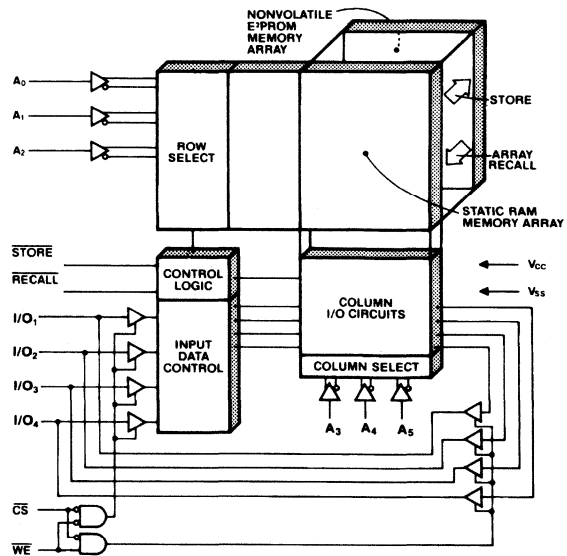


0045-1

### PIN NAMES

A <sub>0</sub> -A <sub>5</sub>	Address Inputs
I/O <sub>1</sub> -I/O <sub>4</sub>	Data Inputs/Outputs
WE	Write Enable
CS	Chip Select
ARRAY RECALL	Array Recall
STORE	Store
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0045-2

# X2210, X2210I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2210	-10°C to +85°C
X2210I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2210  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

X2210I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2210 Limits		X2210I Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	Power Supply Current		50		55	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{LI}$	Input Load Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 4.2$ mA
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -2$ mA

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0$  MHz,  $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0V$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

## MODE SELECTION

Inputs				Input Output I/O	Mode
CS	WE	ARRAY RECALL	STORE		
H	X	H	H	Output High Z	Not Selected <sup>(2)</sup>
L	H	H	H	Output Data	Read RAM
L	L	H	H	Input Data High	Write "1" RAM
L	L	H	H	Input Data Low	Write "0" RAM
X	H	L	H	Output High Z	Array Recall
H	X	L	H	Output High Z	Array Recall
X	H	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>
H	X	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>

**Notes:** (1) This parameter is periodically sampled and not 100% tested.

(2) Chip is deselected but may be automatically completing a store cycle.

(3)  $\overline{\text{STORE}} = \text{L}$  is required only to initiate the store cycle, after which the store cycle will be automatically completed ( $\overline{\text{STORE}} = \text{X}$ ).

# X2210, X2210I

## A.C. CHARACTERISTICS

X2210  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

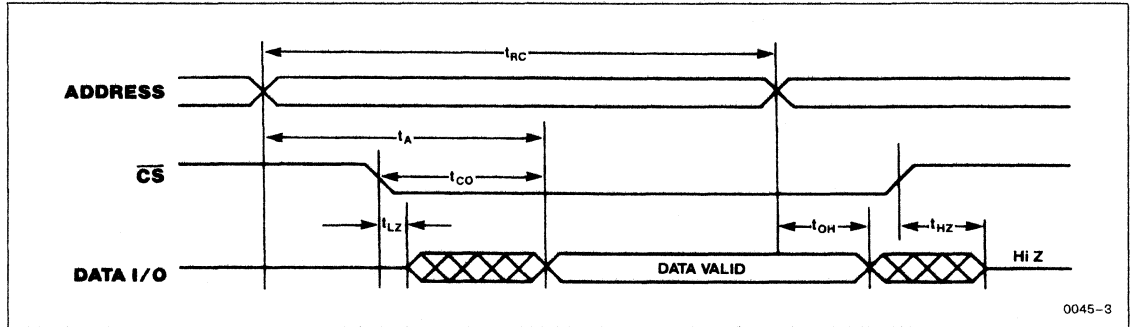
X2210I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

1

### Read Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RC}$	Read Cycle Time	300		ns
$t_A$	Access Time		300	ns
$t_{CO}$	Chip Select to Output Valid		200	ns
$t_{OH}$	Output Hold from Address Change	50		ns
$t_{LZ}$	Chip Select to Output in Low Z	10		ns
$t_{HZ}$	Chip Deselect to Output in High Z	10	100	ns

### Read Cycle

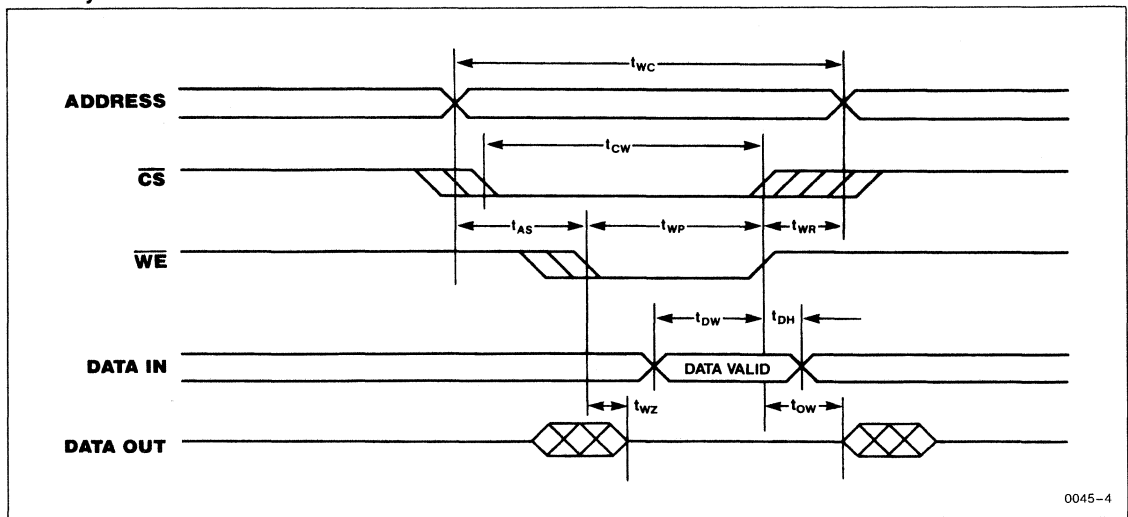


# X2210, X2210I

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	300		ns
$t_{CW}$	Chip Select to End of Write	150		ns
$t_{AS}$	Address Setup Time	50		ns
$t_{WP}$	Write Pulse Width	150		ns
$t_{WR}$	Write Recovery Time	25		ns
$t_{DW}$	Data Valid to End of Write	100		ns
$t_{DH}$	Data Hold Time	X2210	0	ns
		X2210I	20	ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	ns
$t_{OW}$	Output Active from End of Write	10		ns

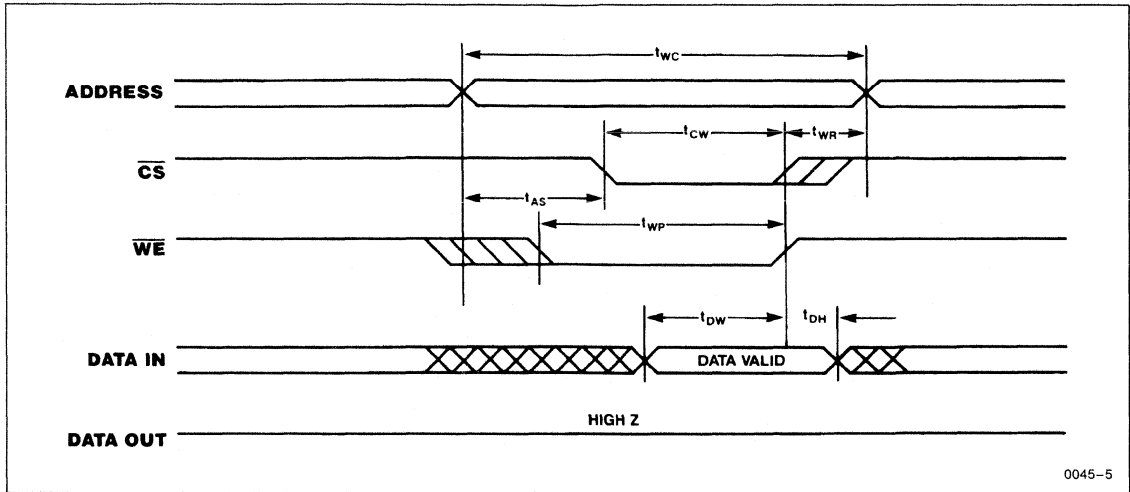
## Write Cycle



# X2210, X2210I

1

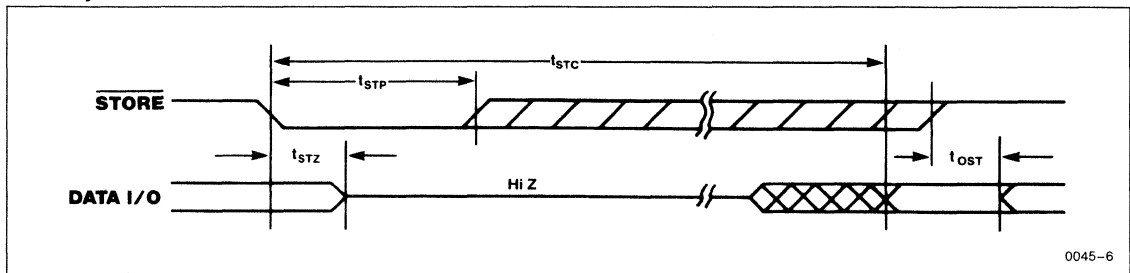
## Early Write Cycle



## Store Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{STC}$	Store Cycle Time		10	ms
$t_{STP}$	Store Pulse Width	100		ns
$t_{STZ}$	Store to Output in High Z		500	ns
$t_{OST}$	Output Active from End of Store	10		ns

## Store Cycle

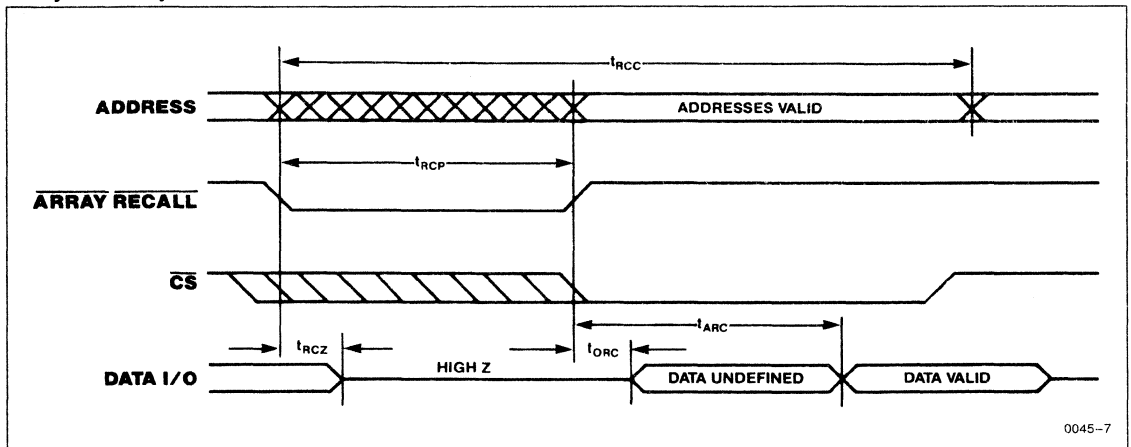


# X2210, X2210I

## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RCC}$	Array Recall Cycle Time	1200		ns
$t_{RCP}$	Recall Pulse Width <sup>(4)</sup>	450		ns
$t_{RCZ}$	Recall to Output in High Z		150	ns
$t_{ORC}$	Output Active from End of Recall	10		ns
$t_{ARC}$	Recalled Data Access Time from End of Recall		750	ns

## Array Recall Cycle



**Note:** (4) Array Recall rise time must be less than 1  $\mu$ s.

# X2210, X2210I

## PIN DESCRIPTIONS AND DEVICE OPERATION

### Addresses (A<sub>0</sub>–A<sub>5</sub>)

The address inputs select a 4-bit memory location during a read or write operation.

### Chip Select ( $\overline{CS}$ )

The Chip Select input must be LOW to enable read/write operations with the RAM array.  $\overline{CS}$  HIGH will place the I/O pins in the high impedance state.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the I/O buffers, determining whether a RAM read or write operation is enabled.  $\overline{WE}$  HIGH enables a read and  $\overline{WE}$  LOW enables a write.

### Data In/Data Out (I/O<sub>1</sub>–I/O<sub>4</sub>)

Data is written to or read from the X2210 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CS}$  is HIGH or during either a store or recall operation.

### STORE

The  $\overline{STORE}$  input, when LOW, will initiate the transfer of the entire contents of the RAM array to the E<sup>2</sup>PROM array. The  $\overline{WE}$  and  $\overline{ARRAY\ RECALL}$  inputs are inhibited during the store cycle. The store operation will be completed in 10 ms or less.

A store operation has priority over RAM read/write operations. If  $\overline{STORE}$  is asserted during a read operation, the read will be discontinued. If  $\overline{STORE}$  is asserted during a RAM write operation, the write will be immediately terminated and the store performed. The data at the RAM address that was being written will be unknown in both the RAM and E<sup>2</sup>PROM.

### ARRAY RECALL

The  $\overline{ARRAY\ RECALL}$  input, when LOW, will initiate the transfer of the entire contents of the E<sup>2</sup>PROM array to the RAM array. The transfer of data will typically be completed in 1  $\mu$ s or less.

An array recall has priority over RAM read/write operations and will terminate both operations when  $\overline{ARRAY\ RECALL}$  is asserted.  $\overline{ARRAY\ RECALL}$  LOW will also inhibit the  $\overline{STORE}$  input.

### WRITE PROTECTION

The X2210 has three write protect features that are employed to protect the contents of the nonvolatile memory.

- V<sub>CC</sub> Sense—All functions are inhibited when V<sub>CC</sub> is  $\leq 3V$ , typically.






- Write Inhibit—Holding either  $\overline{STORE}$  HIGH or  $\overline{ARRAY\ RECALL}$  LOW during power-up or power-down will prevent an inadvertent store operation and E<sup>2</sup>PROM data integrity will be maintained.
- Noise Protection—A  $\overline{STORE}$  pulse of less than 20 ns will *not* initiate a store cycle.

## ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

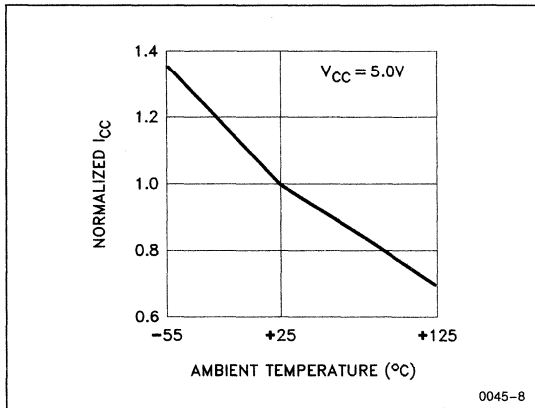
Part Number	Store Cycles	Data Changes Per Bit
X2210 X2210I	10,000	1,000
X2210/5 X2210I/5	50,000	5,000
X2210/10 X2210I/10	100,000	10,000

## SYMBOL TABLE

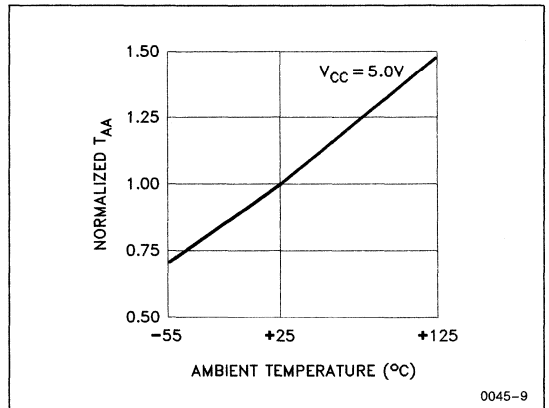
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2210, X2210I

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**





## Nonvolatile Static RAM

### FEATURES

- Single 5V Supply
- Fully TTL Compatible
- Infinite E<sup>2</sup>PROM Array Recall, RAM Read and Write Cycles
- Access Time of 300 ns Max.
- Nonvolatile Store Inhibit: V<sub>CC</sub> = 3V Typical
- 100 Year Data Retention
- JEDEC Standard 18-Pin Package

### DESCRIPTION

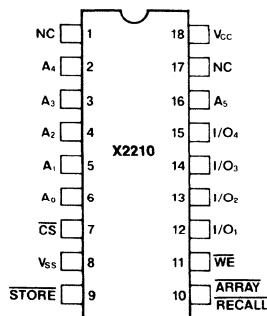
The Xicor X2210 is a 64 x 4 NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile E<sup>2</sup>PROM. The X2210 is fabricated with the same reliable N-channel floating gate MOS technology used

in all Xicor 5V nonvolatile memories. The X2210 features the JEDEC approved pinout for 4-bit-wide memories, compatible with industry standard RAMs.

The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and from E<sup>2</sup>PROM to RAM (recall). The store operation is completed in 10 ms or less and the recall is typically completed in 1 μs.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM. The E<sup>2</sup>PROM array is designed for a minimum 10,000 store cycles. Data retention is specified to be greater than 100 years.

### PIN CONFIGURATION

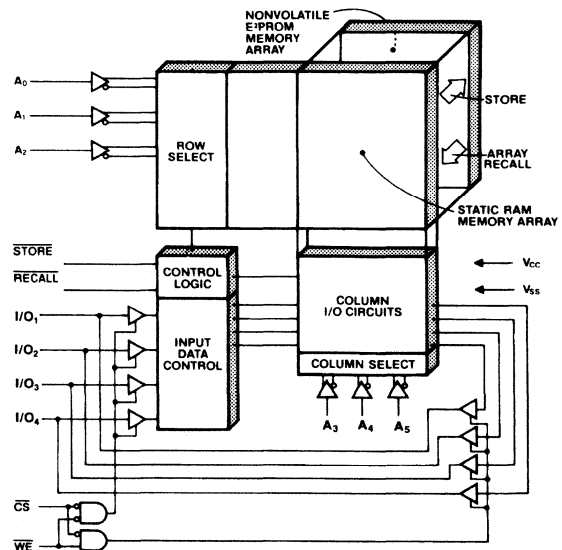


0057-1

### PIN NAMES

A <sub>0</sub> -A <sub>5</sub>	Address Inputs
I/O <sub>1</sub> -I/O <sub>4</sub>	Data Inputs/Outputs
WE	Write Enable
CS	Chip Select
ARRAY RECALL	Array Recall
STORE	Store
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0057-2

# X2210M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	.....	-65°C to +135°C
Storage Temperature	.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground	.....	-1.0V to +7V
D.C. Output Current	.....	5 mA
Lead Temperature (Soldering, 10 Seconds)	.....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	Power Supply Current		55	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0\text{ mA}$
$I_{LI}$	Input Load Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 4.2\text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -2\text{ mA}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0\text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

## MODE SELECTION

Inputs				Input Output I/O	Mode
CS	WE	ARRAY RECALL	STORE		
H	X	H	H	Output High Z	Not Selected <sup>(2)</sup>
L	H	H	H	Output Data	Read RAM
L	L	H	H	Input Data High	Write "1" RAM
L	L	H	H	Input Data Low	Write "0" RAM
X	H	L	H	Output High Z	Array Recall
H	X	L	H	Output High Z	Array Recall
X	H	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>
H	X	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>

**Notes:** (1) This parameter is periodically sampled and not 100% tested.

(2) Chip is deselected but may be automatically completing a store cycle.

(3) STORE = L is required only to initiate the store cycle, after which the store cycle will be automatically completed (STORE = X).

# X2210M

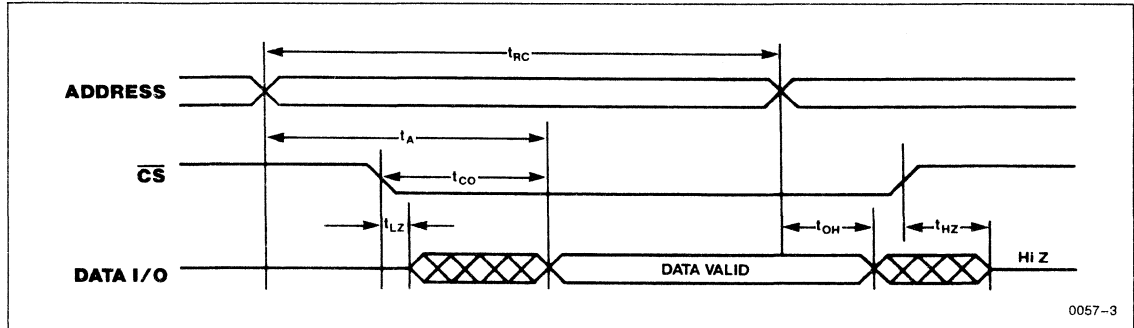
## A.C. CHARACTERISTICS

$T_A = -55^{\circ}\text{C}$  to  $+125^{\circ}\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RC}$	Read Cycle Time	300		ns
$t_A$	Access Time		300	ns
$t_{CO}$	Chip Select to Output Valid		200	ns
$t_{OH}$	Output Hold from Address Change	50		ns
$t_{LZ}$	Chip Select to Output in Low Z	10		ns
$t_{HZ}$	Chip Deselect to Output in High Z	10	100	ns

### Read Cycle



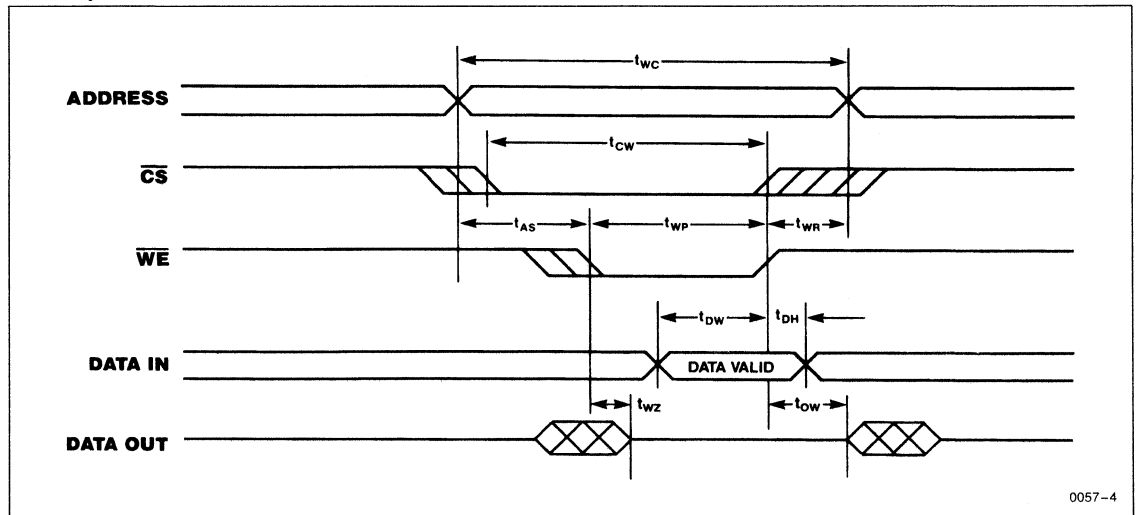
1

# X2210M

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	300		ns
$t_{CW}$	Chip Select to End of Write	150		ns
$t_{AS}$	Address Setup Time	50		ns
$t_{WP}$	Write Pulse Width	150		ns
$t_{WR}$	Write Recovery Time	25		ns
$t_{DW}$	Data Valid to End of Write	100		ns
$t_{DH}$	Data Hold Time	20		ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	ns
$t_{OW}$	Output Active from End of Write	10		ns

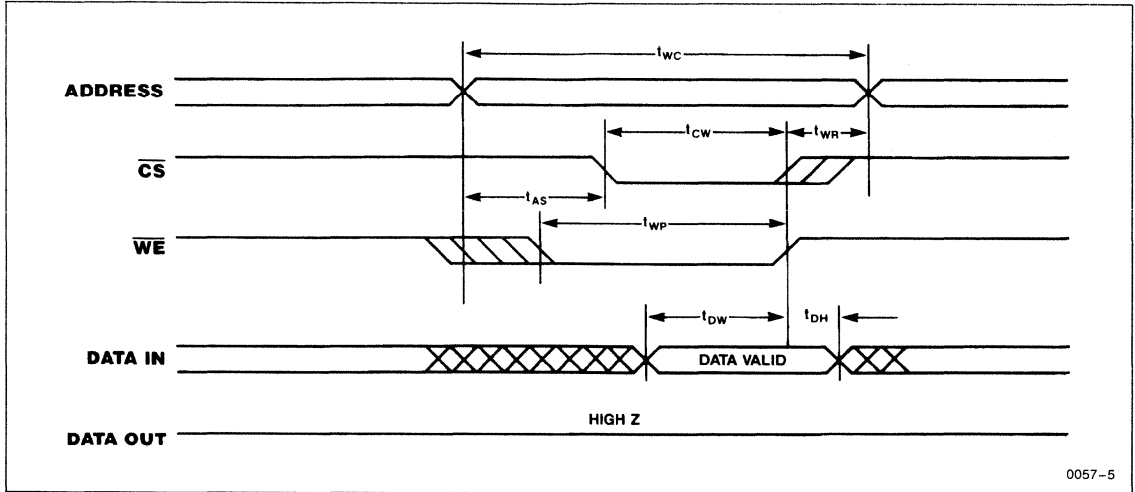
## Write Cycle



# X2210M

1

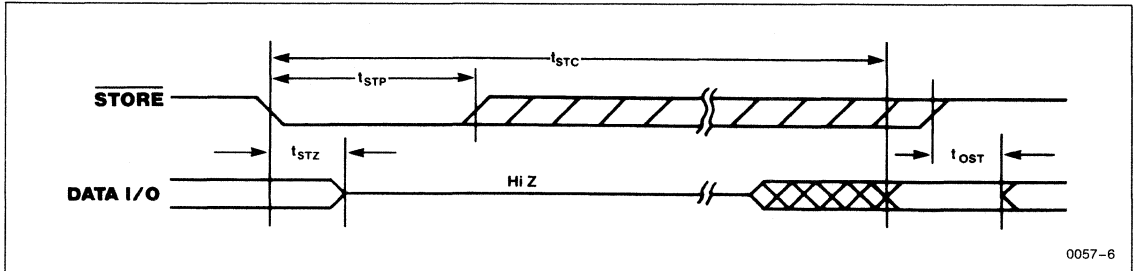
## Early Write Cycle



## Store Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{STC}$	Store Cycle Time		10	ms
$t_{STP}$	Store Pulse Width	100		ns
$t_{STZ}$	Store to Output in High Z		500	ns
$t_{OST}$	Output Active from End of Store	10		ns

## Store Cycle

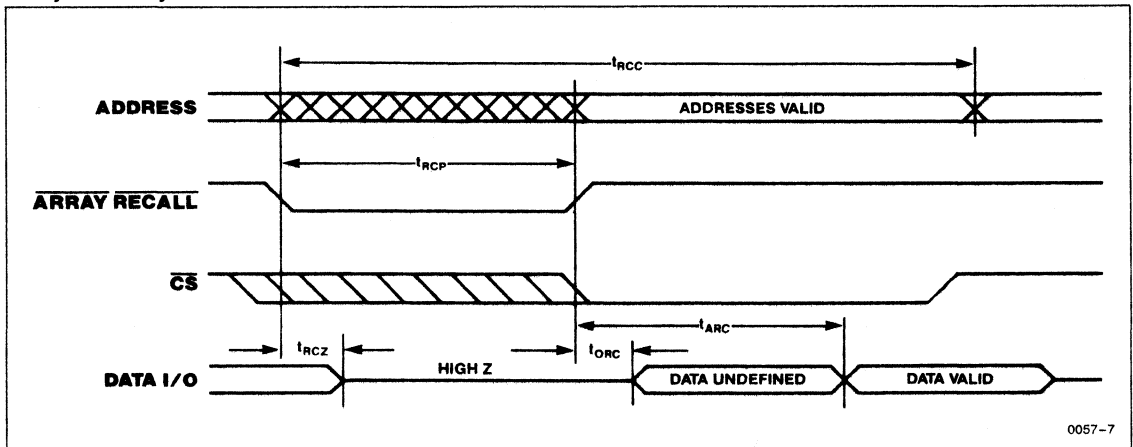


# X2210M

## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RCC}$	Array Recall Cycle Time	1200		ns
$t_{RCP}$	Recall Pulse Width <sup>(4)</sup>	450		ns
$t_{RCZ}$	Recall to Output in High Z		150	ns
$t_{ORC}$	Output Active from End of Recall	10		ns
$t_{ARC}$	Recalled Data Access Time from End of Recall		750	ns

## Array Recall Cycle



**Note:** (4) Array Recall rise time must be less than 1  $\mu$ s.

# X2210M

1

## PIN DESCRIPTIONS AND DEVICE OPERATION

### Addresses ( $A_0$ – $A_5$ )

The address inputs select a 4-bit memory location during a read or write operation.

### Chip Select ( $\overline{CS}$ )

The Chip Select input must be LOW to enable read/write operations with the RAM array.  $\overline{CS}$  HIGH will place the I/O pins in the high impedance state.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the I/O buffers, determining whether a RAM read or write operation is enabled.  $\overline{WE}$  HIGH enables a read and  $\overline{WE}$  LOW enables a write.

### Data In/Data Out ( $I/O_1$ – $I/O_4$ )

Data is written to or read from the X2210 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CS}$  is HIGH or during either a store or recall operation.

### STORE

The  $\overline{STORE}$  input, when LOW, will initiate the transfer of the entire contents of the RAM array to the E<sup>2</sup>PROM array. The  $\overline{WE}$  and  $\overline{ARRAY\ RECALL}$  inputs are inhibited during the store cycle. The store operation will be completed in 10 ms or less.

A store operation has priority over RAM read/write operations. If  $\overline{STORE}$  is asserted during a read operation, the read will be discontinued. If  $\overline{STORE}$  is asserted during a RAM write operation, the write will be immediately terminated and the store performed. The data at the RAM address that was being written will be unknown in both the RAM and E<sup>2</sup>PROM.

### ARRAY RECALL

The  $\overline{ARRAY\ RECALL}$  input, when LOW, will initiate the transfer of the entire contents of the E<sup>2</sup>PROM array to the RAM array. The transfer of data will typically be completed in 1  $\mu$ s or less.

An array recall has priority over RAM read/write operations and will terminate both operations when  $\overline{ARRAY\ RECALL}$  is asserted.  $\overline{ARRAY\ RECALL}$  LOW will also inhibit the  $\overline{STORE}$  input.

### WRITE PROTECTION

The X2210 has three write protect features that are employed to protect the contents of the nonvolatile memory.

- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.






- Write Inhibit—Holding either  $\overline{STORE}$  HIGH or  $\overline{ARRAY\ RECALL}$  LOW during power-up or power-down will prevent an inadvertent store operation and E<sup>2</sup>PROM data integrity will be maintained.
- Noise Protection—A  $\overline{STORE}$  pulse of less than 20 ns will *not* initiate a store cycle.

## ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAms are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

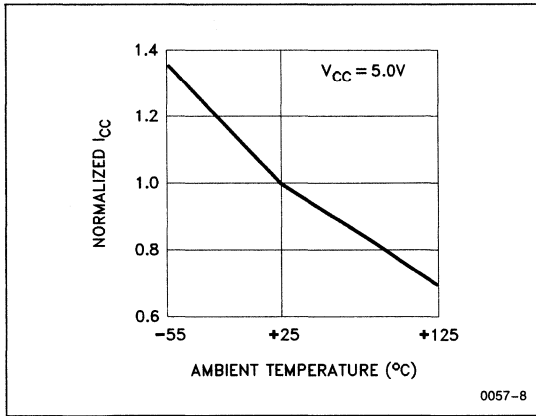
Part Number	Store Cycles	Data Changes Per Bit
X2210M	10,000	1,000
X2210M/5	50,000	5,000
X2210M/10	100,000	10,000

## SYMBOL TABLE

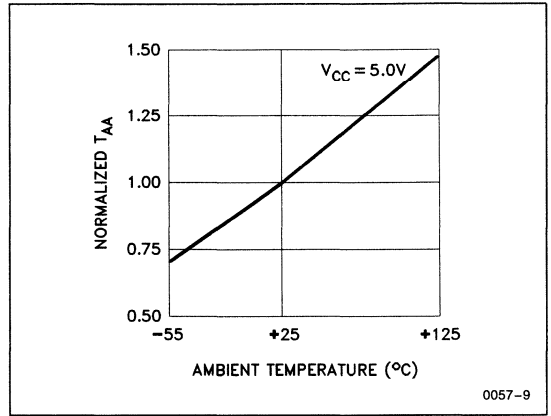
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2210M

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**





1K

Commercial  
Industrial

X2212  
X2212I

256 x 4 Bit

## Nonvolatile Static RAM

1

### FEATURES

- Single 5V Supply
- Fully TTL Compatible
- Infinite E<sup>2</sup>PROM Array Recall, RAM Read and Write Cycles
- Access Time of 300 ns Max.
- Nonvolatile Store Inhibit: V<sub>CC</sub> = 3V Typical
- 100 Year Data Retention
- JEDEC Standard 18-Pin Package

### DESCRIPTION

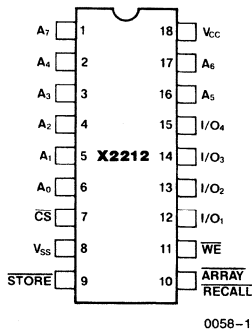
The Xicor X2212 is a 256 x 4 NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile E<sup>2</sup>PROM. The X2212 is fabricated with the same reliable N-channel floating gate MOS technology used

in all Xicor 5V nonvolatile memories. The X2212 features the JEDEC approved pinout for 4-bit-wide memories, compatible with industry standard RAMs.

The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and from E<sup>2</sup>PROM to RAM (recall). The store operation is completed in 10 ms or less and the recall is typically completed in 1 μs.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM. The E<sup>2</sup>PROM array is designed for a minimum 10,000 store cycles. Data retention is specified to be greater than 100 years.

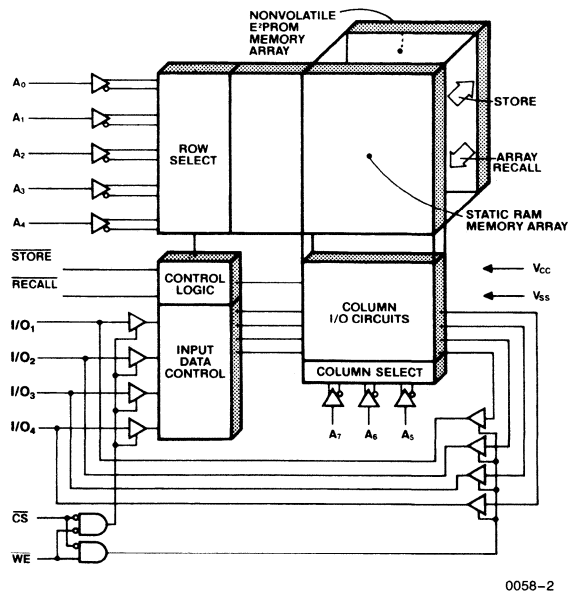
### PIN CONFIGURATION



### PIN NAMES

A <sub>0</sub> -A <sub>7</sub>	Address Inputs
I/O <sub>1</sub> -I/O <sub>4</sub>	Data Inputs/Outputs
WE	Write Enable
CS	Chip Select
ARRAY RECALL	Array Recall
STORE	Store
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2212, X2212I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2212	-10°C to +85°C
X2212I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	.5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2212  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

X2212I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2212 Limits		X2212I Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	Power Supply Current		60		70	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{LI}$	Input Load Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 4.2$ mA
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -2$ mA

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0$ MHz, $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0V$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

## MODE SELECTION

Inputs				Input Output I/O	Mode
CS	WE	ARRAY RECALL	STORE		
H	X	H	H	Output High Z	Not Selected <sup>(2)</sup>
L	H	H	H	Output Data	Read RAM
L	L	H	H	Input Data High	Write "1" RAM
L	L	H	H	Input Data Low	Write "0" RAM
X	H	L	H	Output High Z	Array Recall
H	X	L	H	Output High Z	Array Recall
X	H	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>
H	X	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>

Notes: (1) This parameter is periodically sampled and not 100% tested.

(2) Chip is deselected but may be automatically completing a store cycle.

(3)  $\overline{\text{STORE}} = L$  is required only to initiate the store cycle, after which the store cycle will be automatically completed ( $\overline{\text{STORE}} = X$ ).

# X2212, X2212I

## A.C. CHARACTERISTICS

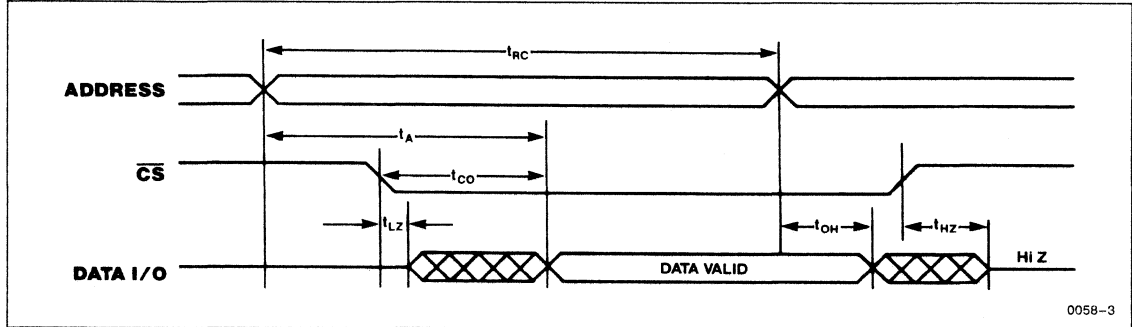
X2212  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

X2212I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RC}$	Read Cycle Time	300		ns
$t_A$	Access Time		300	ns
$t_{CO}$	Chip Select to Output Valid		200	ns
$t_{OH}$	Output Hold from Address Change	50		ns
$t_{LZ}$	Chip Select to Output in Low Z	10		ns
$t_{HZ}$	Chip Deselect to Output in High Z	10	100	ns

### Read Cycle

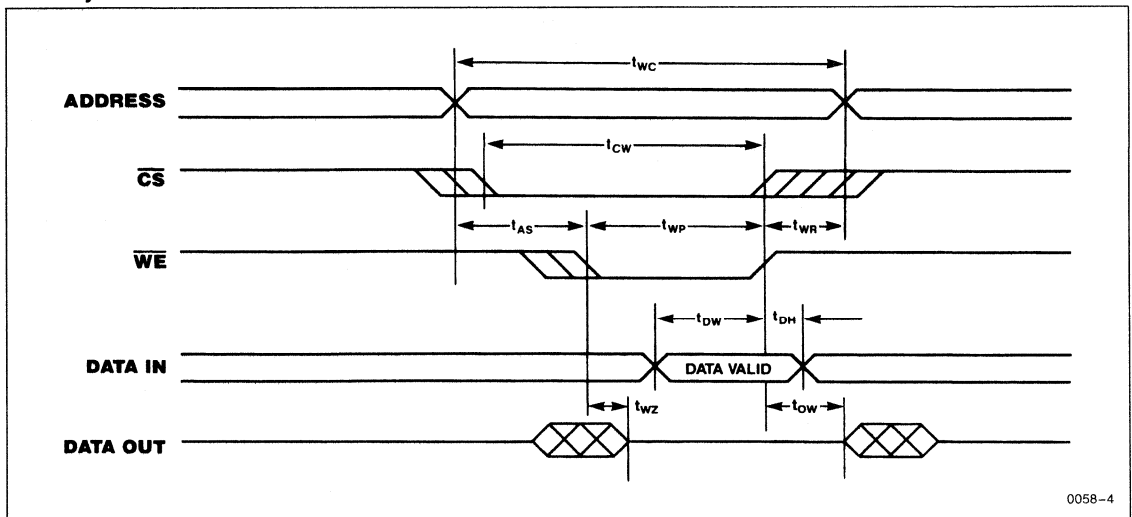


# X2212, X2212I

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	300		ns
$t_{CW}$	Chip Select to End of Write	150		ns
$t_{AS}$	Address Setup Time	50		ns
$t_{WP}$	Write Pulse Width	150		ns
$t_{WR}$	Write Recovery Time	25		ns
$t_{DW}$	Data Valid to End of Write	100		ns
$t_{DH}$	Data Hold Time	X2212	0	ns
		X2212I	20	ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	ns
$t_{OW}$	Output Active from End of Write	10		ns

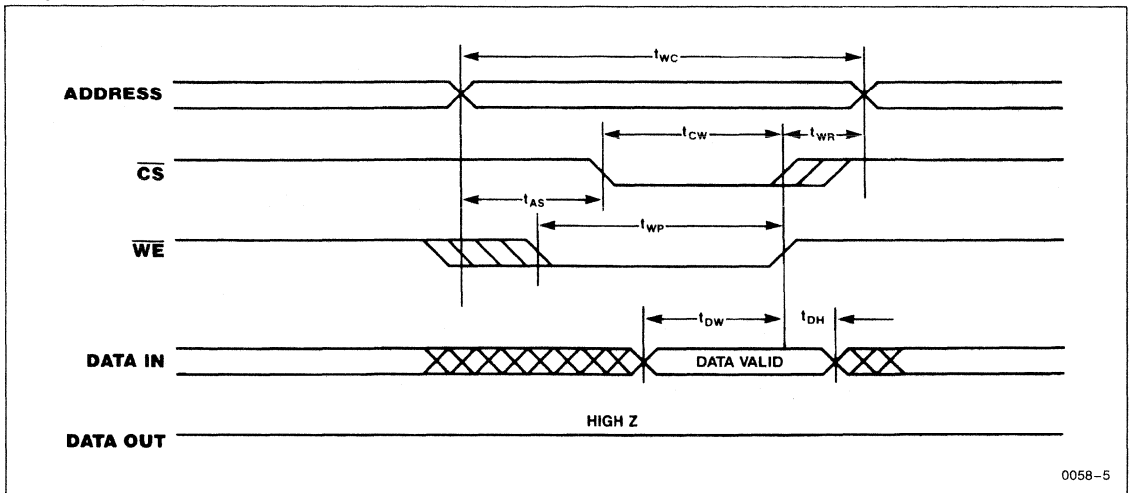
## Write Cycle



# X2212, X2212I

1

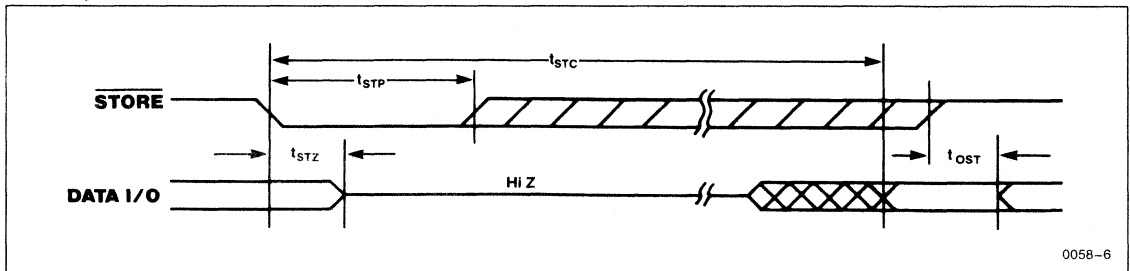
## Early Write Cycle



## Store Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{STC}$	Store Cycle Time		10	ms
$t_{STP}$	Store Pulse Width	100		ns
$t_{STZ}$	Store to Output in High Z		500	ns
$t_{OST}$	Output Active from End of Store	10		ns

## Store Cycle

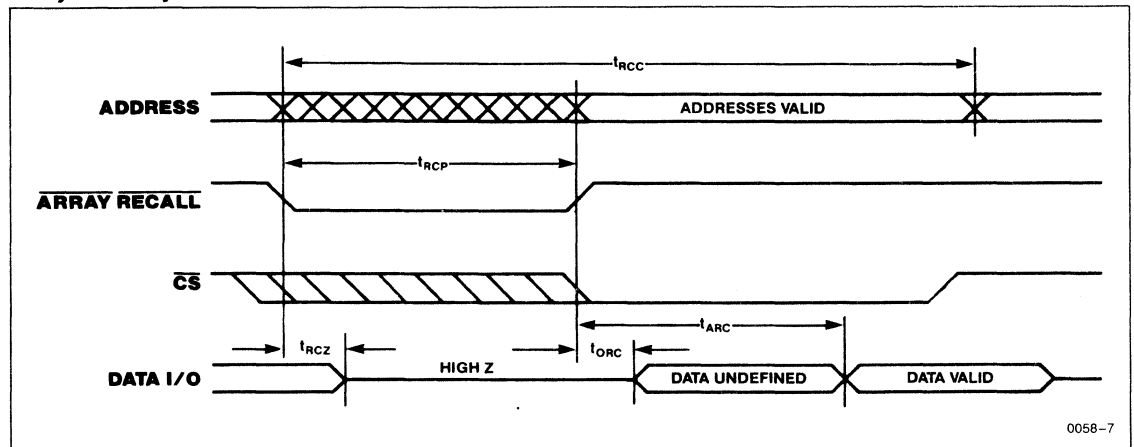


# X2212, X2212I

## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RCC}$	Array Recall Cycle Time	1200		ns
$t_{RCP}$	Recall Pulse Width <sup>(4)</sup>	450		ns
$t_{RCZ}$	Recall to Output in High Z		150	ns
$t_{ORC}$	Output Active from End of Recall	10		ns
$t_{ARC}$	Recalled Data Access Time from End of Recall		750	ns

## Array Recall Cycle



**Note:** (4) Array Recall rise time must be less than 1  $\mu$ s.

# X2212, X2212I

## PIN DESCRIPTIONS AND DEVICE OPERATION

### Addresses (A<sub>0</sub>–A<sub>7</sub>)

The address inputs select a 4-bit memory location during a read or write operation.

### Chip Select ( $\overline{CS}$ )

The Chip Select input must be LOW to enable read/write operations with the RAM array.  $\overline{CS}$  HIGH will place the I/O pins in the high impedance state.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the I/O buffers, determining whether a RAM read or write operation is enabled.  $\overline{WE}$  HIGH enables a read and  $\overline{WE}$  LOW enables a write.

### Data In/Data Out (I/O<sub>1</sub>–I/O<sub>4</sub>)

Data is written to or read from the X2212 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CS}$  is HIGH or during either a store or recall operation.

### STORE

The STORE input, when LOW, will initiate the transfer of the entire contents of the RAM array to the E<sup>2</sup>PROM array. The  $\overline{WE}$  and ARRAY RECALL inputs are inhibited during the store cycle. The store operation will be completed in 10 ms or less.

A store operation has priority over RAM read/write operations. If STORE is asserted during a read operation, the read will be discontinued. If STORE is asserted during a RAM write operation, the write will be immediately terminated and the store performed. The data at the RAM address that was being written will be unknown in both the RAM and E<sup>2</sup>PROM.

### ARRAY RECALL

The ARRAY RECALL input, when LOW, will initiate the transfer of the entire contents of the E<sup>2</sup>PROM array to the RAM array. The transfer of data will typically be completed in 1  $\mu$ s or less.

An array recall has priority over RAM read/write operations and will terminate both operations when ARRAY RECALL is asserted. ARRAY RECALL LOW will also inhibit the STORE input.

### WRITE PROTECTION

The X2212 has three write protect features that are employed to protect the contents of the nonvolatile memory.

- V<sub>CC</sub> Sense—All functions are inhibited when V<sub>CC</sub> is  $\leq 3V$ , typically.






- Write Inhibit—Holding either STORE HIGH or ARRAY RECALL LOW during power-up or power-down will prevent an inadvertent store operation and E<sup>2</sup>PROM data integrity will be maintained.
- Noise Protection—A STORE pulse of less than 20 ns will *not* initiate a store cycle.

### ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

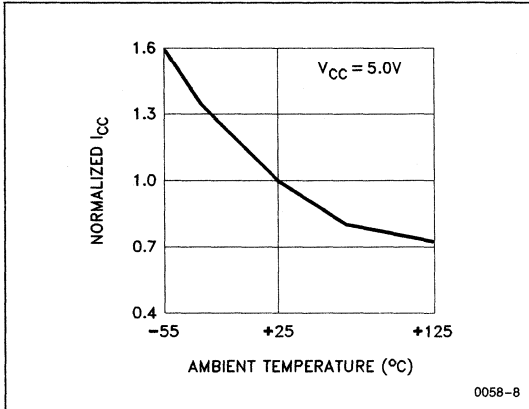
Part Number	Store Cycles	Data Changes Per Bit
X2212 X2212I	10,000	1,000
X2212/5 X2212I/5	50,000	5,000
X2212/10 X2212I/10	100,000	10,000

### SYMBOL TABLE

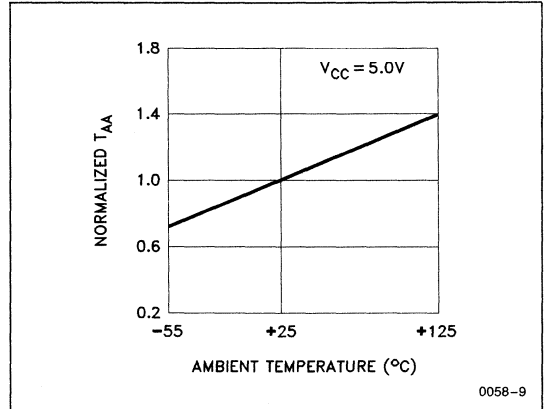
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2212, X2212I

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**





**Nonvolatile Static RAM**

**FEATURES**

- Single 5V Supply
- Fully TTL Compatible
- Infinite E<sup>2</sup>PROM Array Recall, RAM Read and Write Cycles
- Access Time of 300 ns Max.
- Nonvolatile Store Inhibit: V<sub>CC</sub> = 3V Typical
- 100 Year Data Retention
- JEDEC Standard 18-Pin Package

**DESCRIPTION**

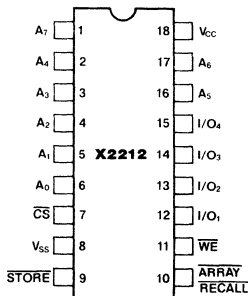
The Xicor X2212 is a 256 x 4 NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile E<sup>2</sup>PROM. The X2212 is fabricated with the same reliable N-channel floating gate MOS technology used

in all Xicor 5V nonvolatile memories. The X2212 features the JEDEC approved pinout for 4-bit-wide memories, compatible with industry standard RAMs.

The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and from E<sup>2</sup>PROM to RAM (recall). The store operation is completed in 10 ms or less and the recall is typically completed in 1 μs.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM. The E<sup>2</sup>PROM array is designed for a minimum 10,000 store cycles. Data retention is specified to be greater than 100 years.

**PIN CONFIGURATION**

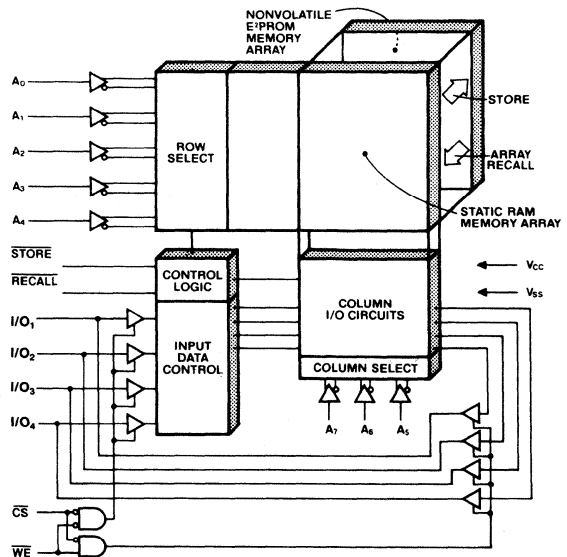


0059-1

**PIN NAMES**

A <sub>0</sub> -A <sub>7</sub>	Address Inputs
I/O <sub>1</sub> -I/O <sub>4</sub>	Data Inputs/Outputs
WE	Write Enable
CS	Chip Select
ARRAY RECALL	Array Recall
STORE	Store
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

**FUNCTIONAL DIAGRAM**



0059-2

# X2212M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	..... -65°C to +135°C
Storage Temperature	..... -65°C to +150°C
Voltage on any Pin with Respect to Ground	..... -1.0V to +7V
D.C. Output Current	..... 5 mA
Lead Temperature (Soldering, 10 Seconds)	..... 300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C to } +125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	Power Supply Current		70	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{LI}$	Input Load Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 4.2$ mA
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -2$ mA

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0$  MHz,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

## MODE SELECTION

Inputs				Input Output I/O	Mode
CS	WE	ARRAY RECALL	STORE		
H	X	H	H	Output High Z	Not Selected <sup>(2)</sup>
L	H	H	H	Output Data	Read RAM
L	L	H	H	Input Data High	Write "1" RAM
L	L	H	H	Input Data Low	Write "0" RAM
X	H	L	H	Output High Z	Array Recall
H	X	L	H	Output High Z	Array Recall
X	H	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>
H	X	H	L	Output High Z	Nonvolatile Storing <sup>(3)</sup>

**Notes:** (1) This parameter is periodically sampled and not 100% tested.

(2) Chip is deselected but may be automatically completing a store cycle.

(3)  $\overline{\text{STORE}} = \text{L}$  is required only to initiate the store cycle, after which the store cycle will be automatically completed ( $\overline{\text{STORE}} = \text{X}$ ).

# X2212M

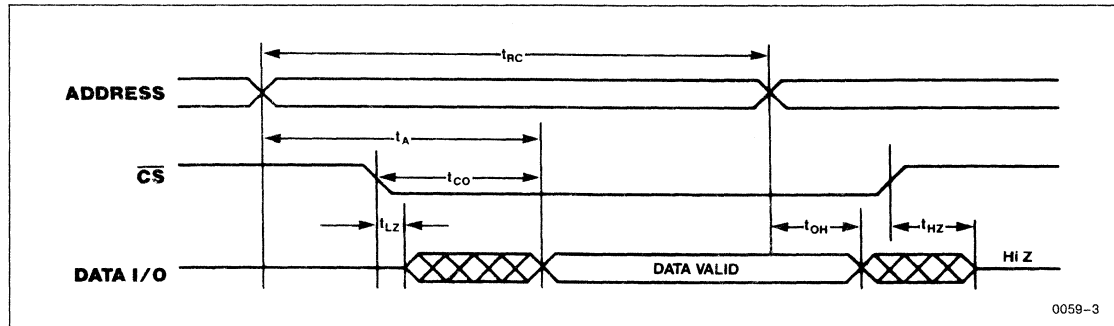
## A.C. CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RC}$	Read Cycle Time	300		ns
$t_A$	Access Time		300	ns
$t_{CO}$	Chip Select to Output Valid		200	ns
$t_{OH}$	Output Hold from Address Change	50		ns
$t_{LZ}$	Chip Select to Output in Low Z	10		ns
$t_{HZ}$	Chip Deselect to Output in High Z	10	100	ns

### Read Cycle



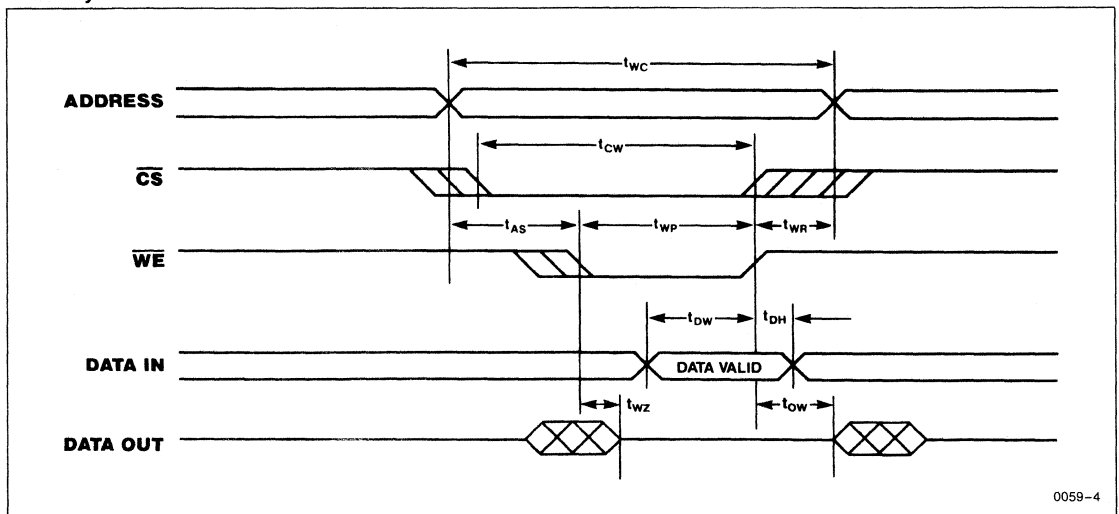
1

# X2212M

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	300		ns
$t_{CW}$	Chip Select to End of Write	150		ns
$t_{AS}$	Address Setup Time	50		ns
$t_{WP}$	Write Pulse Width	150		ns
$t_{WR}$	Write Recovery Time	25		ns
$t_{DW}$	Data Valid to End of Write	100		ns
$t_{DH}$	Data Hold Time	20		ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	ns
$t_{OW}$	Output Active from End of Write	10		ns

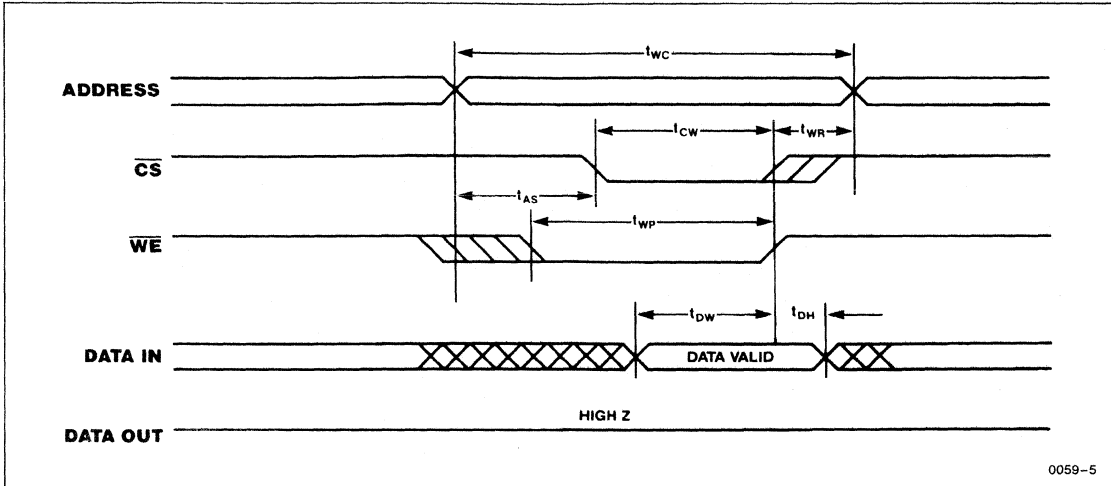
## Write Cycle



# X2212M

1

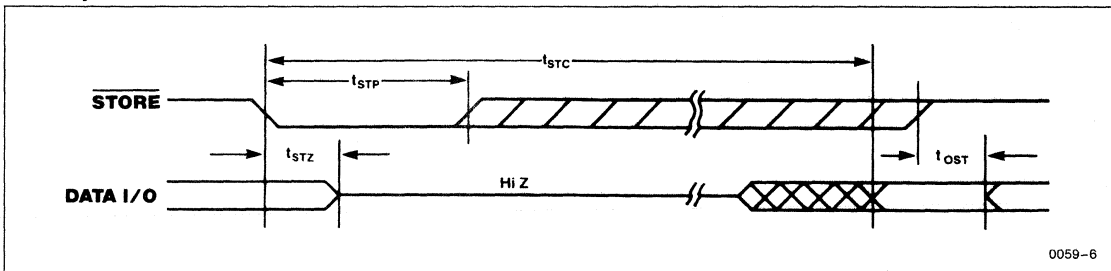
## Early Write Cycle



## Store Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{STC}$	Store Cycle Time		10	ms
$t_{STP}$	Store Pulse Width	100		ns
$t_{STZ}$	Store to Output in High Z		500	ns
$t_{OST}$	Output Active from End of Store	10		ns

## Store Cycle

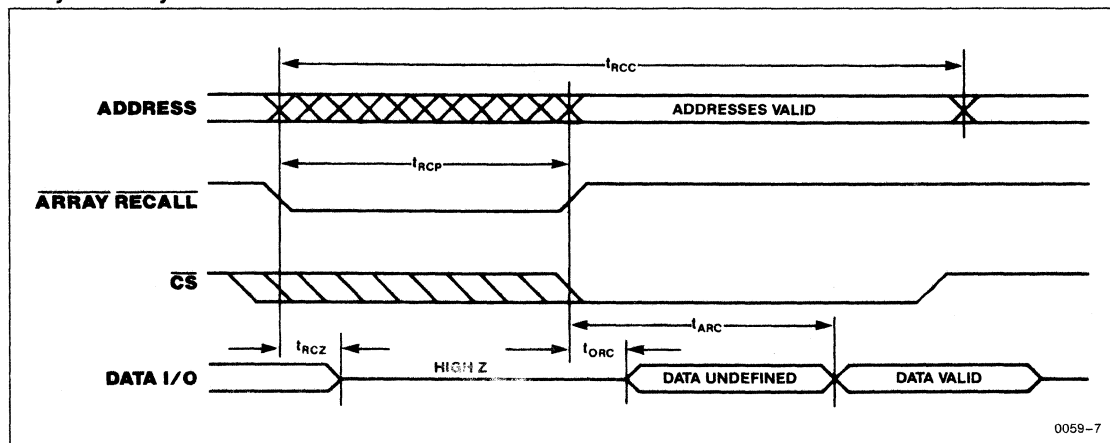


# X2212M

## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RCC}$	Array Recall Cycle Time	1200		ns
$t_{RCP}$	Recall Pulse Width <sup>(4)</sup>	450		ns
$t_{RCZ}$	Recall to Output in High Z		150	ns
$t_{ORC}$	Output Active from End of Recall	10		ns
$t_{ARC}$	Recalled Data Access Time from End of Recall		750	ns

## Array Recall Cycle



**Note:** (4) Array Recall rise time must be less than 1  $\mu$ s.

# X2212M

1

## PIN DESCRIPTIONS AND DEVICE OPERATION

### Addresses (A<sub>0</sub>–A<sub>7</sub>)

The address inputs select a 4-bit memory location during a read or write operation.

### Chip Select ( $\overline{CS}$ )

The Chip Select input must be LOW to enable read/write operations with the RAM array.  $\overline{CS}$  HIGH will place the I/O pins in the high impedance state.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the I/O buffers, determining whether a RAM read or write operation is enabled.  $\overline{WE}$  HIGH enables a read and  $\overline{WE}$  LOW enables a write.

### Data In/Data Out (I/O<sub>1</sub>–I/O<sub>4</sub>)

Data is written to or read from the X2212 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CS}$  is HIGH or during either a store or recall operation.

### STORE

The  $\overline{STORE}$  input, when LOW, will initiate the transfer of the entire contents of the RAM array to the E<sup>2</sup>PROM array. The  $\overline{WE}$  and  $\overline{ARRAY\ RECALL}$  inputs are inhibited during the store cycle. The store operation will be completed in 10 ms or less.

A store operation has priority over RAM read/write operations. If  $\overline{STORE}$  is asserted during a read operation, the read will be discontinued. If  $\overline{STORE}$  is asserted during a RAM write operation, the write will be immediately terminated and the store performed. The data at the RAM address that was being written will be unknown in both the RAM and E<sup>2</sup>PROM.

### ARRAY RECALL

The  $\overline{ARRAY\ RECALL}$  input, when LOW, will initiate the transfer of the entire contents of the E<sup>2</sup>PROM array to the RAM array. The transfer of data will typically be completed in 1  $\mu$ s or less.

An array recall has priority over RAM read/write operations and will terminate both operations when  $\overline{ARRAY\ RECALL}$  is asserted.  $\overline{ARRAY\ RECALL\ LOW}$  will also inhibit the  $\overline{STORE}$  input.

### WRITE PROTECTION

The X2212 has three write protect features that are employed to protect the contents of the nonvolatile memory.

- V<sub>CC</sub> Sense—All functions are inhibited when V<sub>CC</sub> is  $\leq 3V$ , typically.






- Write Inhibit—Holding either  $\overline{STORE}$  HIGH or  $\overline{ARRAY\ RECALL}$  LOW during power-up or power-down will prevent an inadvertent store operation and E<sup>2</sup>PROM data integrity will be maintained.
- Noise Protection—A  $\overline{STORE}$  pulse of less than 20 ns will *not* initiate a store cycle.

## ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

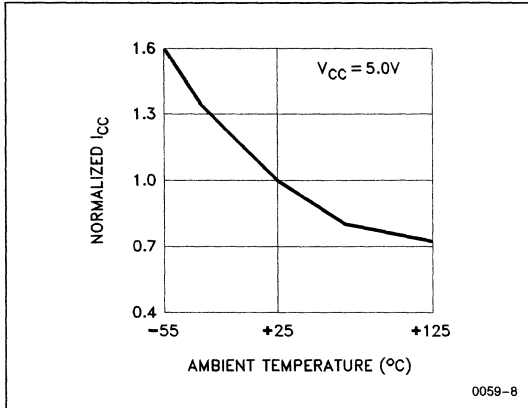
Part Number	Store Cycles	Data Changes Per Bit
X2212M	10,000	1,000
X2212M/5	50,000	5,000
X2212M/10	100,000	10,000

## SYMBOL TABLE

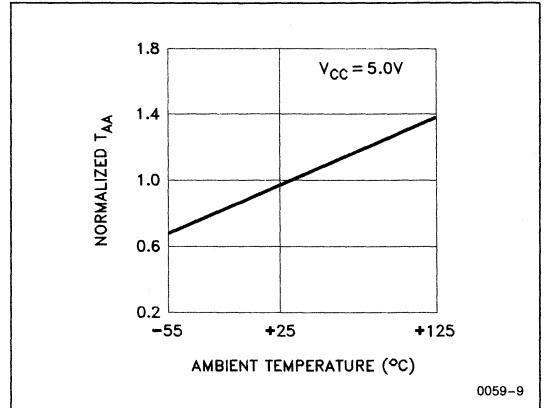
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2212M

**Normalized Active Supply Current  
vs. Ambient Temperature**



**Normalized Access Time  
vs. Ambient Temperature**





**1K Commercial Industrial X2001 X20011 128 x 8 Bit**

---

**Nonvolatile Static RAM**

---

**1**

**FEATURES**

- **Nonvolatile Data Integrity**
- **Automatic Store Timing**
- **Store and Array Recall Combined on One Line ( $\overline{NE}$ )**
- **Enhanced Store Protection**
- **Infinite E<sup>2</sup>PROM Array Recall, and RAM Read and Write Cycles**
- **Single 5V Supply**
- **100 Year Data Retention**
- **Fast Access Time: 200 ns Max.**
- **Automatic Recall on Power-Up**
- **JEDEC Approved Byte-Wide Pinout**

**DESCRIPTION**

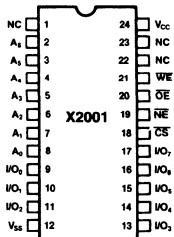
The Xicor X2001 is a byte-wide NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile electrically erasable PROM (E<sup>2</sup>PROM). The X2001

is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2001 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs, EPROMs and E<sup>2</sup>PROMs.

The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and E<sup>2</sup>PROM to RAM (recall). With  $\overline{NE}$  LOW, these functions are performed in the same manner as RAM read and write operations. The store operation is completed in 10 ms or less and the recall operation is completed in 5  $\mu$ s or less.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM, and a minimum 100,000 store operations to the E<sup>2</sup>PROM. Data retention is specified to be greater than 100 years.

**PIN CONFIGURATION**

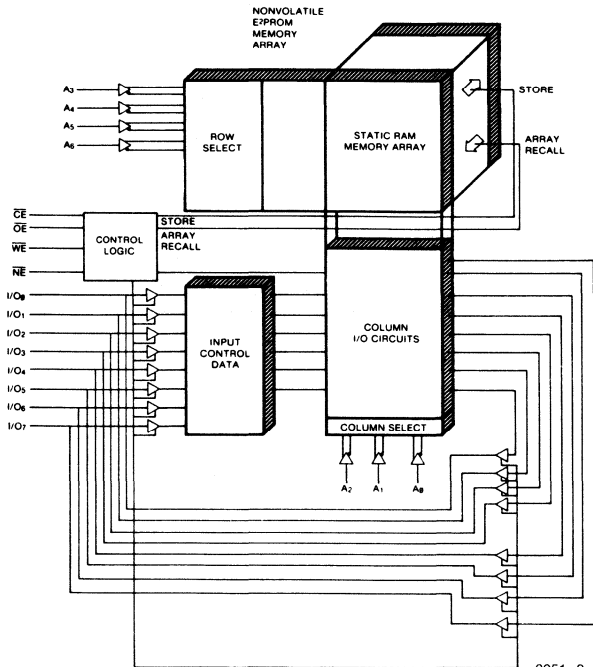


0051-1

**PIN NAMES**

A <sub>0</sub> -A <sub>6</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Inputs/Outputs
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
$\overline{WE}$	Write Enable
$\overline{NE}$	Nonvolatile Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

**FUNCTIONAL DIAGRAM**



0051-2

# X2001, X2001I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2001	-10°C to +85°C
X2001I	-65°C to +135°C
Storage Temperature	
	-65°C to +150°C
Voltage on any Pin with Respect to Ground	
	-1.0V to +7V
D.C. Output Current	
	5 mA
Lead Temperature (Soldering, 10 Seconds)	
	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2001  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2001I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2001 Limits		X2001I Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80		100	mA	$\overline{CE} = V_{IL}$ , All Other Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{SB}$	$V_{CC}$ Current (Standby)		50		65	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{LI}$	Input Leakage Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 0.5$	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 2.1$ mA
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -400$ $\mu\text{A}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0$  MHz,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

## MODE SELECTION

CE	WE	NE	OE	Mode	I/O	Power
H	X	X	X	Not Selected	Output High Z	Standby
L	H	H	L	Read RAM	Output Data	Active
L	L	H	X	Write "1" RAM	Input Data High	Active
L	L	H	X	Write "0" RAM	Input Data Low	Active
L	H	L	L	Array Recall	Output High Z	Active
L	L	L	H	Nonvolatile Storing	Output High Z	Active
L	H	H	H	Output Disabled	Output High Z	Active
L	L	L	L	Not Allowed	Output High Z	Active
L	H	L	H	No Operation	Output High Z	Active

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2001, X2001I

## A.C. CHARACTERISTICS

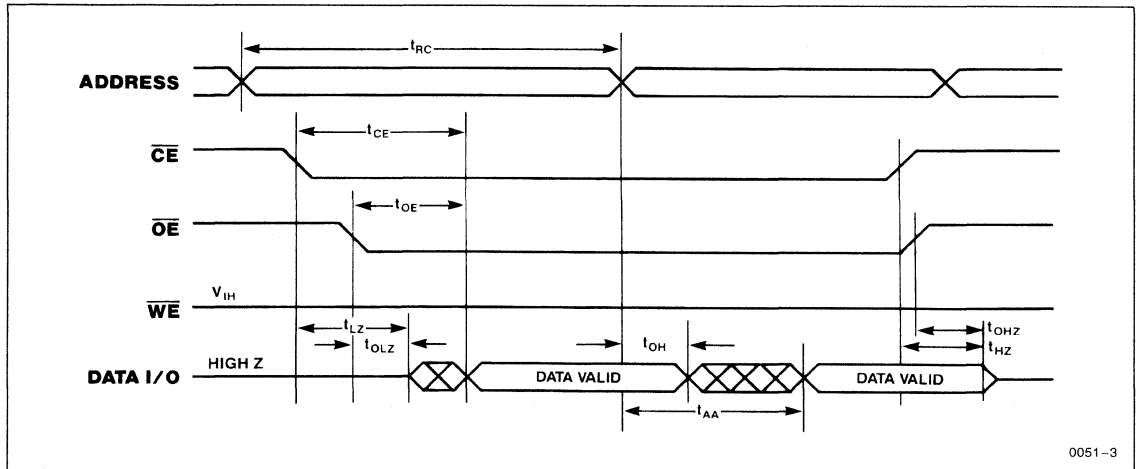
X2001  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2001I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2001-20 X2001I-20		X2001-25 X2001I-25		X2001 X2001I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	200		250		300		ns
$t_{CE}$	Chip Enable Access Time		200		250		300	ns
$t_{AA}$	Address Access Time		200		250		300	ns
$t_{OE}$	Output Enable Access Time		70		100		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	100	10	100	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		10		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	100	10	100	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

### Read Cycle



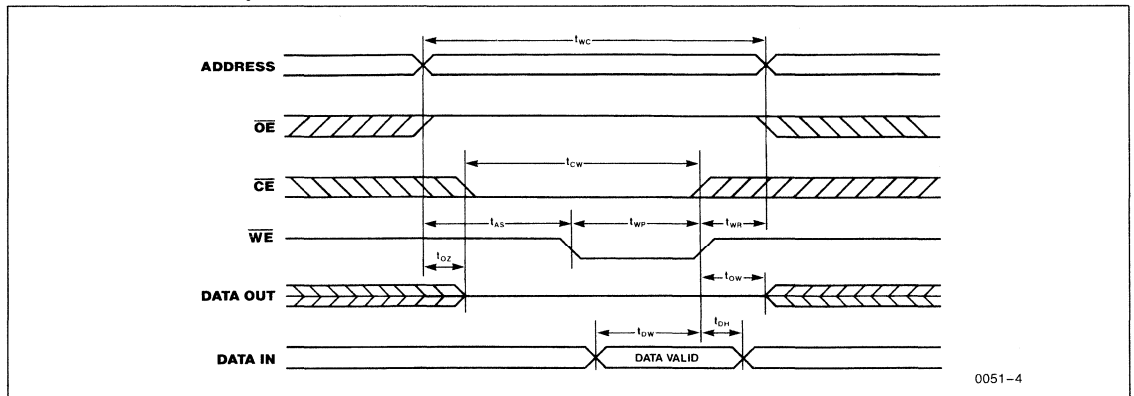
Note: (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2001, X2001I

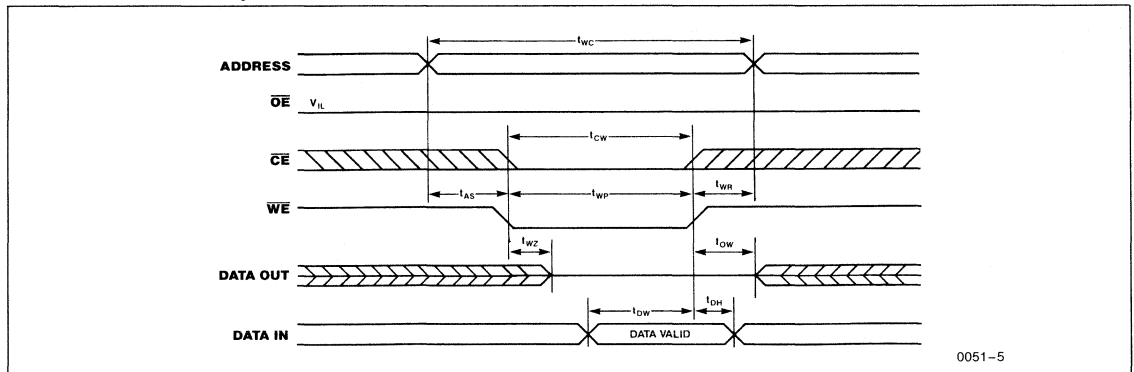
## Write Cycle Limits

Symbol	Parameter	X2001-20 X2001I-20		X2001-25 X2001I-25		X2001 X2001I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	200		250		300		ns
$t_{CW}$	Chip Enable to End of Write Input	200		250		300		ns
$t_{AS}$	Address Setup Time	0		0		0		ns
$t_{WP}$	Write Pulse Width	120		150		200		ns
$t_{WR}$	Write Recovery Time	0		0		0		ns
$t_{Dw}$	Data Valid to End of Write	120		150		200		ns
$t_{DH}$	Data Hold Time	0		0		0		ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	10	100	10	100	ns
$t_{OW}$	Output Active from End of Write	10		10		10		ns
$t_{OZ}$	Output Enable to Output in High Z	10	100	10	100	10	100	ns

## WE Controlled Write Cycle



## CE Controlled Write Cycle



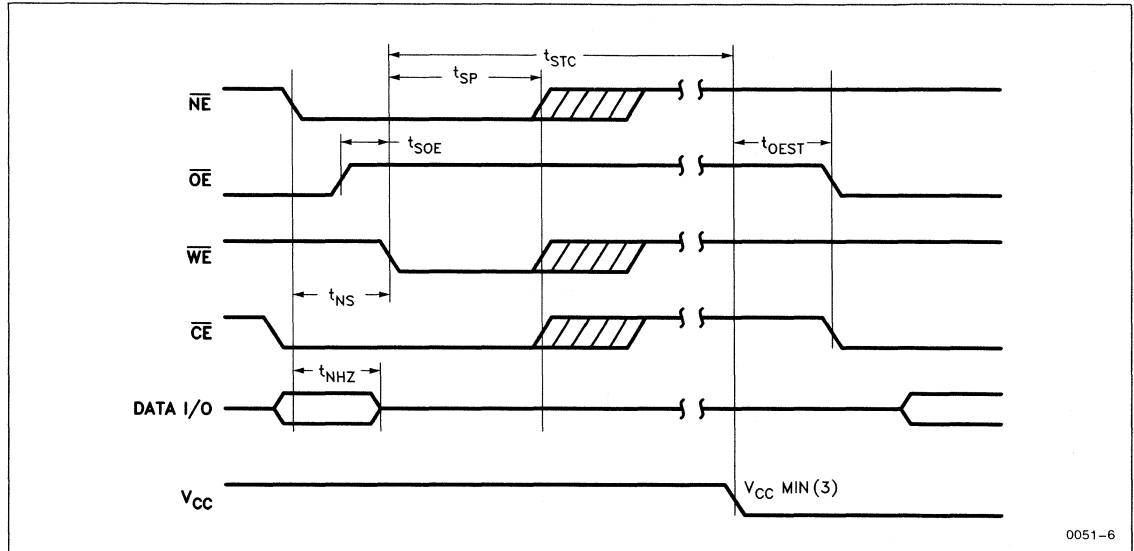
# X2001, X2001I

1

## Store Cycle Limits

Symbol	Parameter	X2001-20 X2001I-20		X2001-25 X2001I-25		X2001 X2001I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{STC}$	Store Cycle Time		10		10		10	ms
$t_{SP}$	Store Pulse Width	120		150		200		ns
$t_{NHZ}$	Nonvolatile Enable to Output in High Z		100		100		100	ns
$t_{OEST}$	Output Enable from End of Store	10		10		10		ns
$t_{SOE}$	$\overline{OE}$ Disable to Store Function	20		20		20		ns
$t_{NS}$	$\overline{NE}$ Setup Time from $\overline{WE}$	0		0		0		ns

## Store Cycle



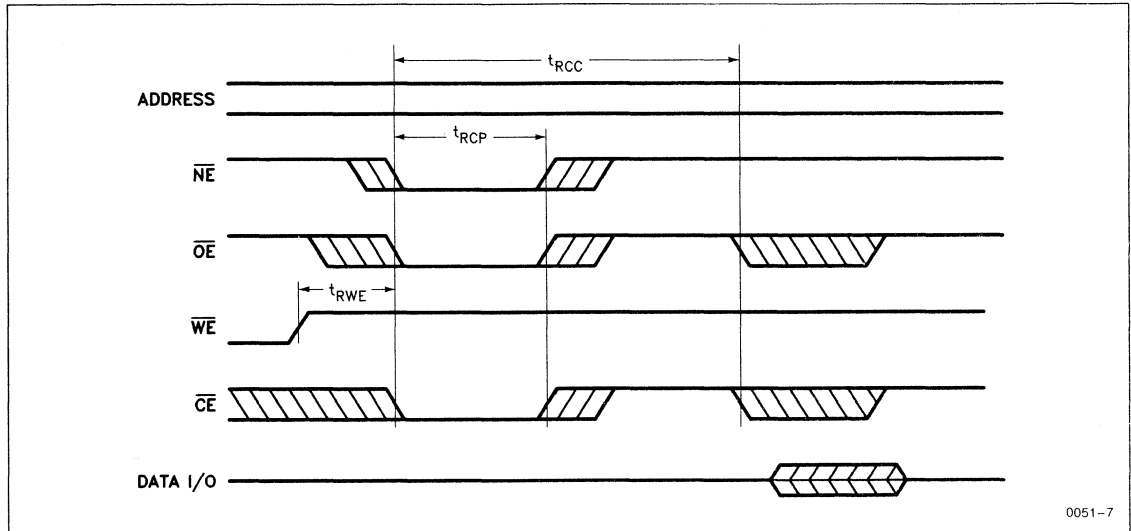
Note: (3) X2001  $V_{CC\ Min.} = 4.75V$   
 X2001I  $V_{CC\ Min.} = 4.5V$

# X2001, X2001I

## Array Recall Cycle Limits

Symbol	Parameter	X2001-20 X2001I-20		X2001-25 X2001I-25		X2001 X2001I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RCC}$	Array Recall Cycle Time		5.0		5.0		5.0	$\mu$ s
$t_{RCP}$	Recall Pulse Width to Initiate Recall	120		150		200		ns
$t_{RWE}$	$\overline{WE}$ Setup Time to $\overline{NE}$	0		0		0		ns

## Array Recall Cycle



# X2001, X2001I

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_6$ )

The address inputs select an 8-bit word during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read and recall operations. Output Enable LOW disables a store operation regardless of the state of  $\overline{CE}$ ,  $\overline{WE}$  or  $\overline{NE}$ .

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2001 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CE}$  or  $\overline{OE}$  is HIGH or when  $\overline{NE}$  is LOW.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to both the static RAM and stores to the E<sup>2</sup>PROM.

### Nonvolatile Enable ( $\overline{NE}$ )

The Nonvolatile Enable input controls all accesses to the E<sup>2</sup>PROM array (store and recall functions).

## DEVICE OPERATION

The  $\overline{CE}$ ,  $\overline{OE}$ ,  $\overline{WE}$  and  $\overline{NE}$  inputs control the X2001 operation. The X2001 byte-wide NOVRAM uses a 2-line control architecture to eliminate bus contention in a system environment. The I/O bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH, or when  $\overline{NE}$  is LOW.

## RAM OPERATIONS

RAM read and write operations are performed as they would be with any static RAM. A read operation

requires  $\overline{CE}$  and  $\overline{OE}$  to be LOW with  $\overline{WE}$  and  $\overline{NE}$  HIGH. A write operation requires  $\overline{CE}$  and  $\overline{WE}$  to be LOW with  $\overline{NE}$  HIGH. There is no limit to the number of read or write operations performed to the RAM portion of the X2001.

## NONVOLATILE OPERATIONS

With  $\overline{NE}$  LOW, recall and store operations are performed in the same manner as RAM read and write operations. A recall operation causes the entire contents of the E<sup>2</sup>PROM to be written into the RAM array. The time required for the operation to complete is 5  $\mu$ s or less. A store operation causes the entire contents of the RAM array to be stored in the nonvolatile E<sup>2</sup>PROM. The time for the operation to complete is 10 ms or less, typically 5 ms.

## POWER-UP RECALL

Upon power-up ( $V_{CC}$ ), the X2001 performs an automatic array recall. When  $V_{CC}$  minimum is reached, the recall is initiated, regardless of the state of  $\overline{CE}$ ,  $\overline{OE}$ ,  $\overline{WE}$  and  $\overline{NE}$ .

## WRITE PROTECTION

The X2001 has three write protect features that are employed to protect the contents of both the nonvolatile memory and the RAM.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will *not* initiate a write cycle.
- Combined Signal Noise Protection—A combined  $\overline{WE}$  and  $\overline{NE}$  ( $\overline{WE} \bullet \overline{NE}$ ) pulse of less than 20 ns will *not* initiate a store cycle.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH,  $\overline{CE}$  HIGH or  $\overline{NE}$  HIGH during power-up or power-down, will prevent an inadvertent store operation.

## X2001, X2001I

---






### ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be "cycled" during a nonvolatile store. This characteristic reduces unneces-

sary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

Part Number	Store Cycles	Data Changes Per Bit
X2001	100,000	10,000
X2001I	100,000	10,000

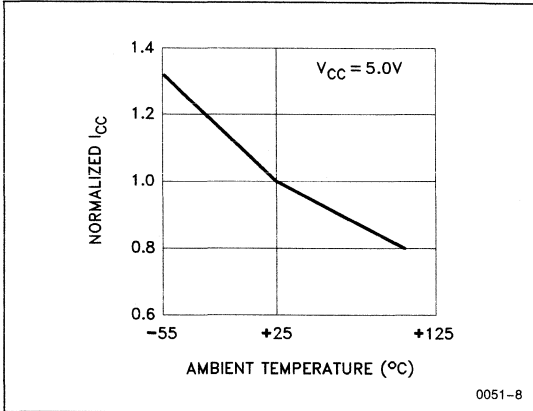
### SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

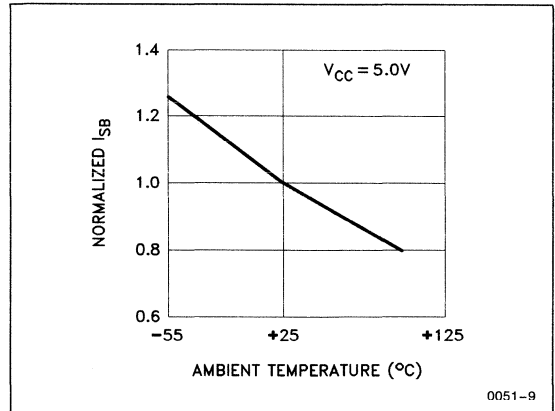


# X2001, X2001I

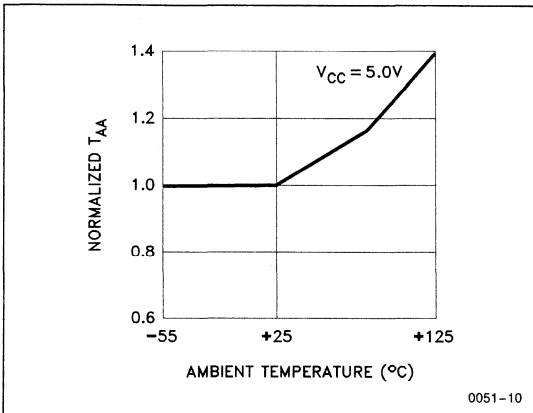
**Normalized Active Supply Current  
vs. Ambient Temperature**



**Normalized Standby Supply Current  
vs. Ambient Temperature**



**Normalized Access Time  
vs. Ambient Temperature**



1

---

## NOTES

**4K**      **Commercial**      **X2004**      **512 x 8 Bit**  
**Industrial**      **X2004I**

## Nonvolatile Static RAM

1

### FEATURES

- Nonvolatile Data Integrity
- Automatic Store Timing
- Store and Array Recall Combined on One Line (NE)
- Enhanced Store Protection
- Infinite E<sup>2</sup>PROM Array Recall, and RAM Read and Write Cycles
- Single 5V Supply
- 100 Year Data Retention
- Fast Access Time: 200 ns Max.
- Automatic Recall on Power-Up
- JEDEC Approved Byte-Wide Pinout

is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2004 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs, EPROMs and E<sup>2</sup>PROMs.

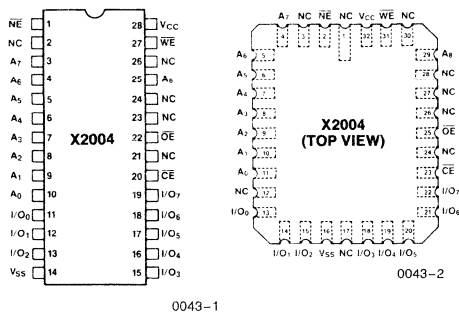
The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and E<sup>2</sup>PROM to RAM (recall). With  $\overline{NE}$  LOW, these functions are performed in the same manner as RAM read and write operations. The store operation is completed in 10 ms or less and the recall operation is completed in 5  $\mu$ s or less.

### DESCRIPTION

The Xicor X2004 is a byte-wide NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile electrically erasable PROM (E<sup>2</sup>PROM). The X2004

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM, and a minimum 100,000 store operations to the E<sup>2</sup>PROM. Data retention is specified to be greater than 100 years.

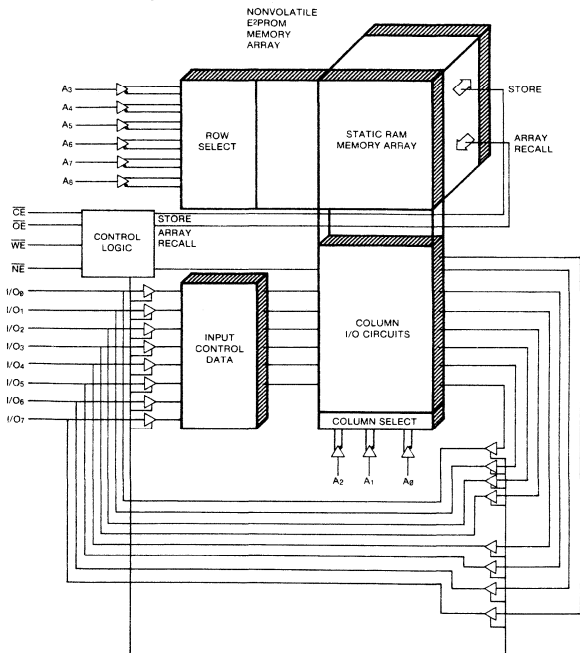
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>8</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Inputs/Outputs
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
$\overline{WE}$	Write Enable
$\overline{NE}$	Nonvolatile Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2004, X2004I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2004	-10°C to +85°C
X2004I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with	
Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature	
(Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2004  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2004I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2004 Limits		X2004I Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		100		120	mA	$\overline{OE} = V_{IL}$ All Other Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{SB}$	$V_{CC}$ Current (Standby)		55		90	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{LI}$	Input Leakage Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 0.5$	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 2.1$ mA
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -400$ $\mu\text{A}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0$  MHz,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

## MODE SELECTION

CE	WE	NE	OE	Mode	I/O	Power
H	X	X	X	Not Selected	Output High Z	Standby
L	H	H	L	Read RAM	Output Data	Active
L	L	H	X	Write "1" RAM	Input Data High	Active
L	L	H	X	Write "0" RAM	Input Data Low	Active
L	H	L	L	Array Recall	Output High Z	Active
L	L	L	H	Nonvolatile Storing	Output High Z	Active
L	H	H	H	Output Disabled	Output High Z	Active
L	L	L	L	Not Allowed	Output High Z	Active
L	H	L	H	No Operation	Output High Z	Active

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2004, X2004I

## A.C. CHARACTERISTICS

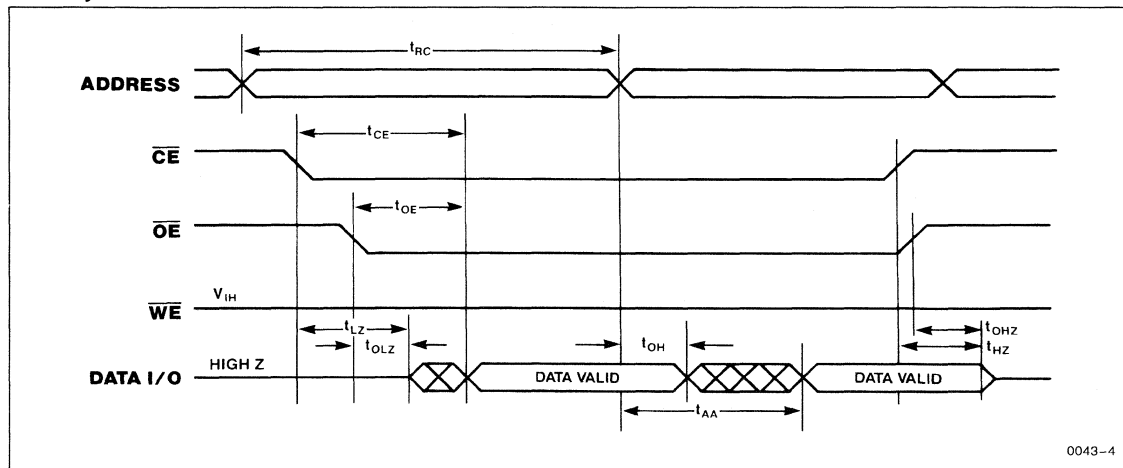
X2004  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2004I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2004-20 X2004I-20		X2004-25 X2004I-25		X2004 X2004I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	200		250		300		ns
$t_{CE}$	Chip Enable Access Time		200		250		300	ns
$t_{AA}$	Address Access Time		200		250		300	ns
$t_{OE}$	Output Enable Access Time		70		100		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	100	10	100	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		10		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	100	10	100	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

### Read Cycle



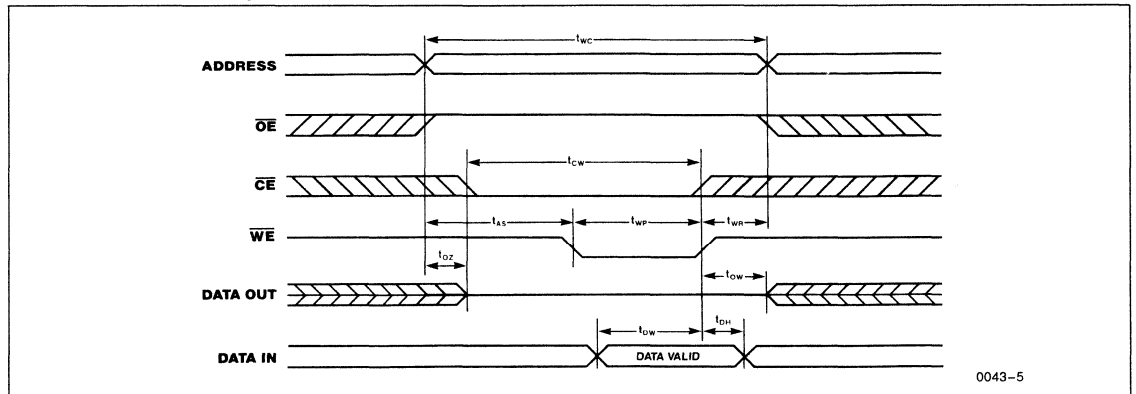
**Note:** (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2004, X2004I

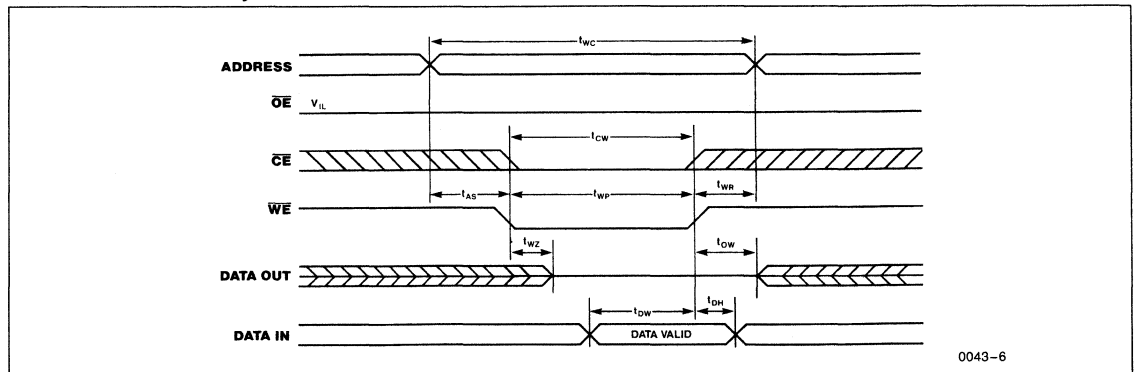
## Write Cycle Limits

Symbol	Parameter	X2004-20 X2004I-20		X2004-25 X2004I-25		X2004 X2004I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	200		250		300		ns
$t_{CW}$	Chip Enable to End of Write Input	200		250		300		ns
$t_{AS}$	Address Setup Time	0		0		0		ns
$t_{WP}$	Write Pulse Width	120		150		200		ns
$t_{WR}$	Write Recovery Time	0		0		0		ns
$t_{DW}$	Data Valid to End of Write	120		150		200		ns
$t_{DH}$	Data Hold Time	0		0		0		ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	10	100	10	100	ns
$t_{OW}$	Output Active from End of Write	10		10		10		ns
$t_{OZ}$	Output Enable to Output in High Z	10	100	10	100	10	100	ns

## $\overline{WE}$ Controlled Write Cycle



## $\overline{CE}$ Controlled Write Cycle



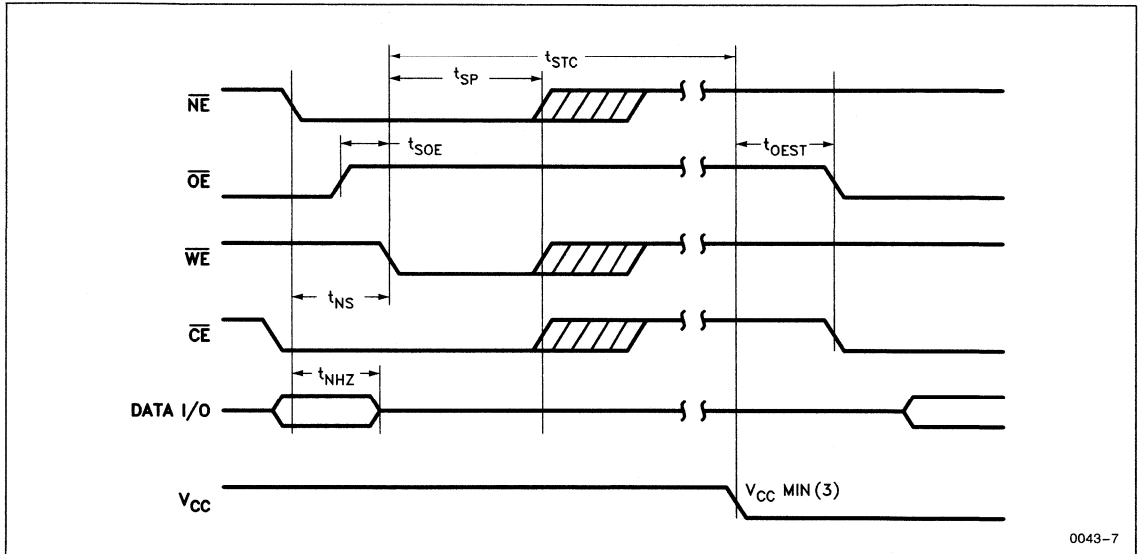
# X2004, X2004I

1

## Store Cycle Limits

Symbol	Parameter	X2004-20 X2004I-20		X2004-25 X2004I-25		X2004 X2004I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{STC}$	Store Cycle Time		10		10		10	ms
$t_{SP}$	Store Pulse Width	120		150		200		ns
$t_{NHZ}$	Nonvolatile Enable to Output in High Z		100		100		100	ns
$t_{OEST}$	Output Enable from End of Store	10		10		10		ns
$t_{SOE}$	$\overline{OE}$ Disable to Store Function	20		20		20		ns
$t_{NS}$	$\overline{NE}$ Setup Time from $\overline{WE}$	0		0		0		ns

## Store Cycle



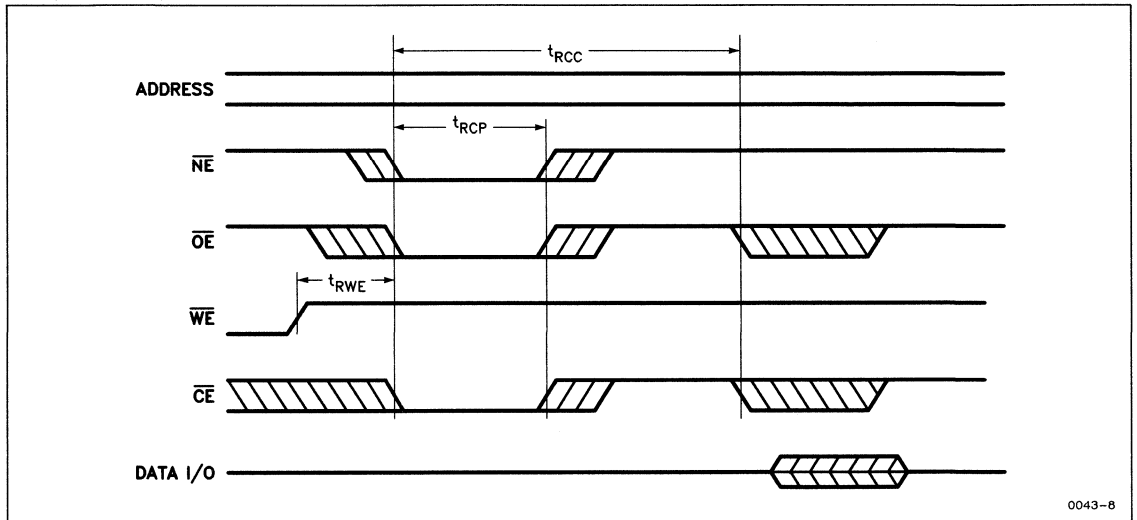
**Note:** (3) X2004  $V_{CC}$  Min. = 4.75V  
X2004I  $V_{CC}$  Min. = 4.5V

# X2004, X2004I

## Array Recall Cycle Limits

Symbol	Parameter	X2004-20 X2004I-20		X2004-25 X2004I-25		X2004 X2004I		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RCC}$	Array Recall Cycle Time		5.0		5.0		5.0	$\mu$ s
$t_{RCP}$	Recall Pulse Width to Initiate Recall	120		150		200		ns
$t_{RWE}$	$\overline{WE}$ Setup Time to $\overline{NE}$	0		0		0		ns

## Array Recall Cycle





## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_8$ )

The address inputs select an 8-bit word during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read and recall operations. Output Enable LOW disables a store operation regardless of the state of  $\overline{CE}$ ,  $\overline{WE}$  or  $\overline{NE}$ .

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2004 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CE}$  or  $\overline{OE}$  is HIGH or when  $\overline{NE}$  is LOW.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to both the static RAM and stores to the E<sup>2</sup>PROM.

### Nonvolatile Enable ( $\overline{NE}$ )

The Nonvolatile Enable input controls all accesses to the E<sup>2</sup>PROM array (store and recall functions).

## DEVICE OPERATION

The  $\overline{CE}$ ,  $\overline{OE}$ ,  $\overline{WE}$  and  $\overline{NE}$  inputs control the X2004 operation. The X2004 byte-wide NOVRAM uses a 2-line control architecture to eliminate bus contention in a system environment. The I/O bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH, or when  $\overline{NE}$  is LOW.

## RAM OPERATIONS

RAM read and write operations are performed as they would be with any static RAM. A read operation

requires  $\overline{CE}$  and  $\overline{OE}$  to be LOW with  $\overline{WE}$  and  $\overline{NE}$  HIGH. A write operation requires  $\overline{CE}$  and  $\overline{WE}$  to be LOW with  $\overline{NE}$  HIGH. There is no limit to the number of read or write operations performed to the RAM portion of the X2004.

## NONVOLATILE OPERATIONS

With  $\overline{NE}$  LOW, recall and store operations are performed in the same manner as RAM read and write operations. A recall operation causes the entire contents of the E<sup>2</sup>PROM to be written into the RAM array. The time required for the operation to complete is 5  $\mu$ s or less. A store operation causes the entire contents of the RAM array to be stored in the nonvolatile E<sup>2</sup>PROM. The time for the operation to complete is 10 ms or less, typically 5 ms.

## POWER-UP RECALL

Upon power-up ( $V_{CC}$ ), the X2004 performs an automatic array recall. When  $V_{CC}$  minimum is reached, the recall is initiated, regardless of the state of  $\overline{CE}$ ,  $\overline{OE}$ ,  $\overline{WE}$  and  $\overline{NE}$ .

## WRITE PROTECTION

The X2004 has four write protect features that are employed to protect the contents of both the nonvolatile memory and the RAM.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will *not* initiate a write cycle.
- Combined Signal Noise Protection—A combined  $\overline{WE}$  and  $\overline{NE}$  ( $\overline{WE} \bullet \overline{NE}$ ) pulse of less than 20 ns will *not* initiate a store cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 2V$ .
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH,  $\overline{CE}$  HIGH or  $\overline{NE}$  HIGH during power-up or power-down, will prevent an inadvertent store operation.

# X2004, X2004I






## ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be "cycled" during a nonvolatile store. This characteristic reduces unneces-

sary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

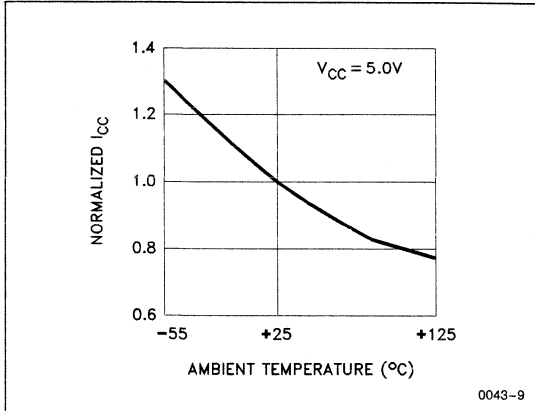
Part Number	Store Cycles	Data Changes Per Bit
X2004	100,000	10,000
X2004I	100,000	10,000

## SYMBOL TABLE

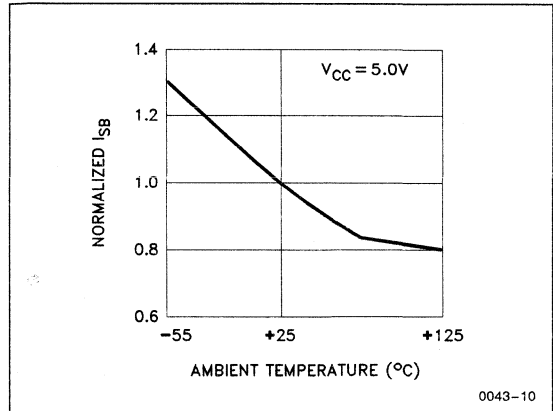
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2004, X2004I

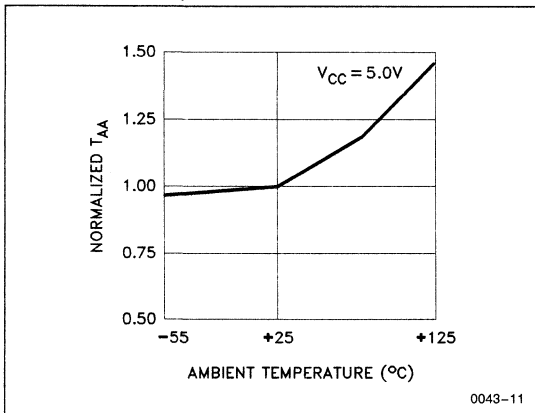
### Normalized Active Supply Current vs. Ambient Temperature



### Normalized Standby Supply Current vs. Ambient Temperature



### Normalized Access Time vs. Ambient Temperature



1

---

## NOTES

## Nonvolatile Static RAM

1

### FEATURES

- Nonvolatile Data Integrity
- Automatic Store Timing
- Store and Array Recall Combined on One Line ( $\overline{NE}$ )
- Enhanced Store Protection
- Infinite E<sup>2</sup>PROM Array Recall, and RAM Read and Write Cycles
- Single 5V Supply
- 100 Year Data Retention
- Fast Access Time: 200 ns Max.
- Automatic Recall on Power-Up
- JEDEC Approved Byte-Wide Pinout

### DESCRIPTION

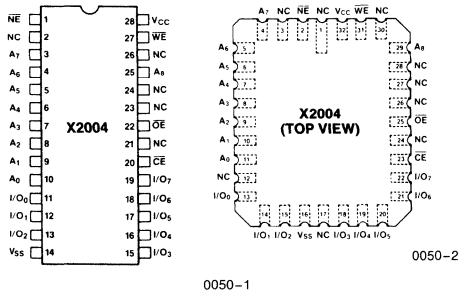
The Xicor X2004 is a byte-wide NOVRAM featuring a high-speed static RAM overlaid bit-for-bit with a nonvolatile electrically erasable PROM (E<sup>2</sup>PROM). The X2004

is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2004 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs, EPROMs and E<sup>2</sup>PROMs.

The NOVRAM design allows data to be easily transferred from RAM to E<sup>2</sup>PROM (store) and E<sup>2</sup>PROM to RAM (recall). With  $\overline{NE}$  LOW, these functions are performed in the same manner as RAM read and write operations. The store operation is completed in 10 ms or less and the recall operation is completed in 5  $\mu$ s or less.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM, and a minimum 100,000 store operations to the E<sup>2</sup>PROM. Data retention is specified to be greater than 100 years.

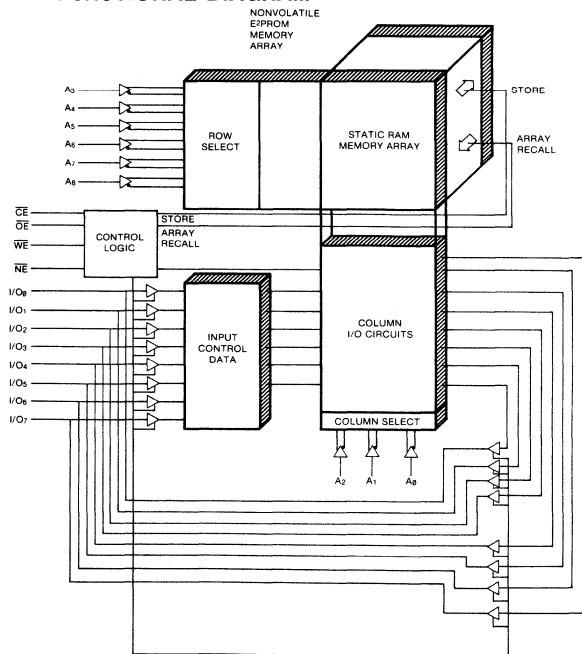
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>8</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Inputs/Outputs
CE	Chip Enable
OE	Output Enable
WE	Write Enable
NE	Nonvolatile Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0050-3

# X2004M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		120	mA	$\overline{CE} = V_{IL}$ , All Other Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{SB}$	$V_{CC}$ Current (Standby)		90	mA	All Inputs = $V_{CC}$ $I_{I/O} = 0$ mA
$I_{LI}$	Input Leakage Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 2.1$ mA
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -400$ $\mu\text{A}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0$  MHz,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

## MODE SELECTION

$\overline{CE}$	$\overline{WE}$	$\overline{NE}$	$\overline{OE}$	Mode	I/O	Power
H	X	X	X	Not Selected	Output High Z	Standby
L	H	H	L	Read RAM	Output Data	Active
L	L	H	X	Write "1" RAM	Input Data High	Active
L	L	H	X	Write "0" RAM	Input Data Low	Active
L	H	L	L	Array Recall	Output High Z	Active
L	L	L	H	Nonvolatile Storing	Output High Z	Active
L	H	H	H	Output Disabled	Output High Z	Active
L	L	L	L	Not Allowed	Output High Z	Active
L	H	L	H	No Operation	Output High Z	Active

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2004M

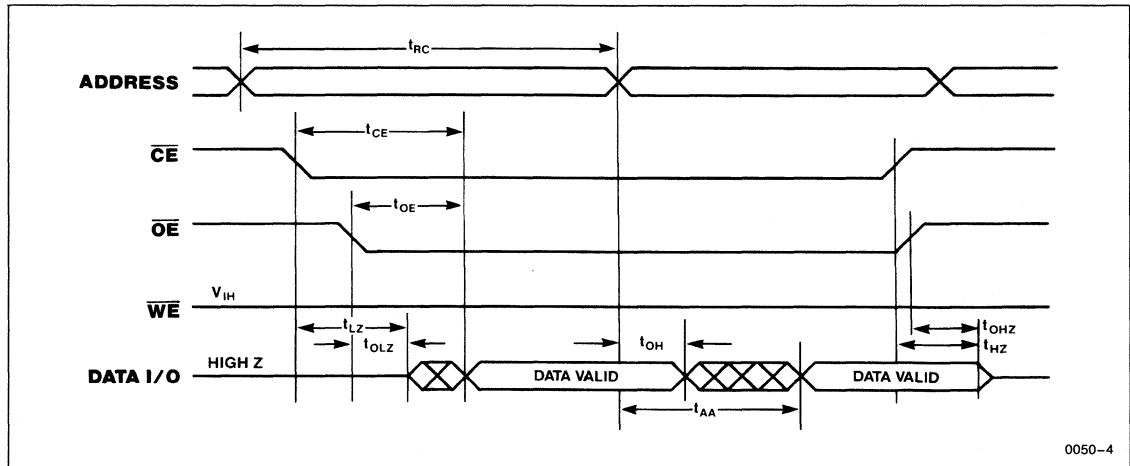
## A.C. CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2004M-25		X2004M		Units
		Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		ns
$t_{CE}$	Chip Enable Access Time		250		300	ns
$t_{AA}$	Address Access Time		250		300	ns
$t_{OE}$	Output Enable Access Time		100		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	100	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	100	ns
$t_{OH}$	Output Hold from Address Change	0		0		ns

### Read Cycle



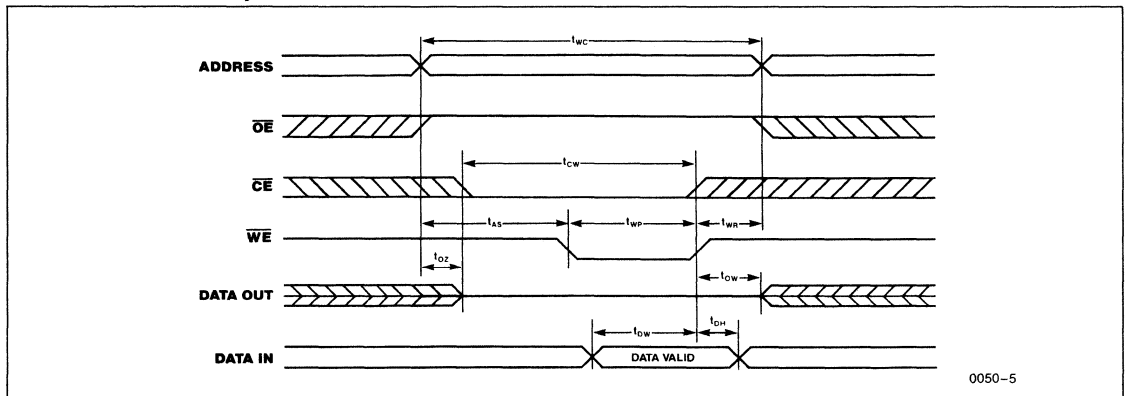
**Note:** (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2004M

## Write Cycle Limits

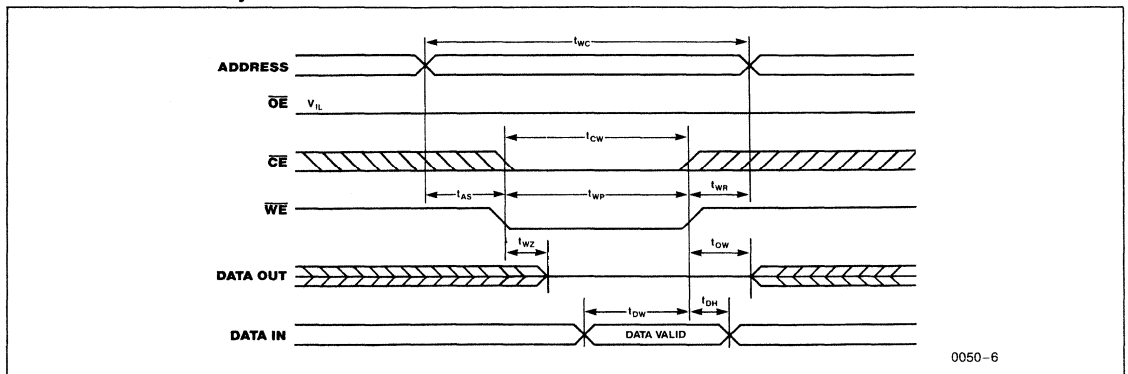
Symbol	Parameter	X2004M-25		X2004M		Units
		Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	250		300		ns
$t_{CW}$	Chip Enable to End of Write Input	250		300		ns
$t_{AS}$	Address Setup Time	0		0		ns
$t_{WP}$	Write Pulse Width	150		200		ns
$t_{WR}$	Write Recovery Time	0		0		ns
$t_{DW}$	Data Valid to End of Write	150		200		ns
$t_{DH}$	Data Hold Time	0		0		ns
$t_{WZ}$	Write Enable to Output in High Z	10	100	10	100	ns
$t_{OW}$	Output Active from End of Write	10		10		ns
$t_{OZ}$	Output Enable to Output in High Z	10	100	10	100	ns

## $\overline{WE}$ Controlled Write Cycle



0050-5

## $\overline{CE}$ Controlled Write Cycle



0050-6



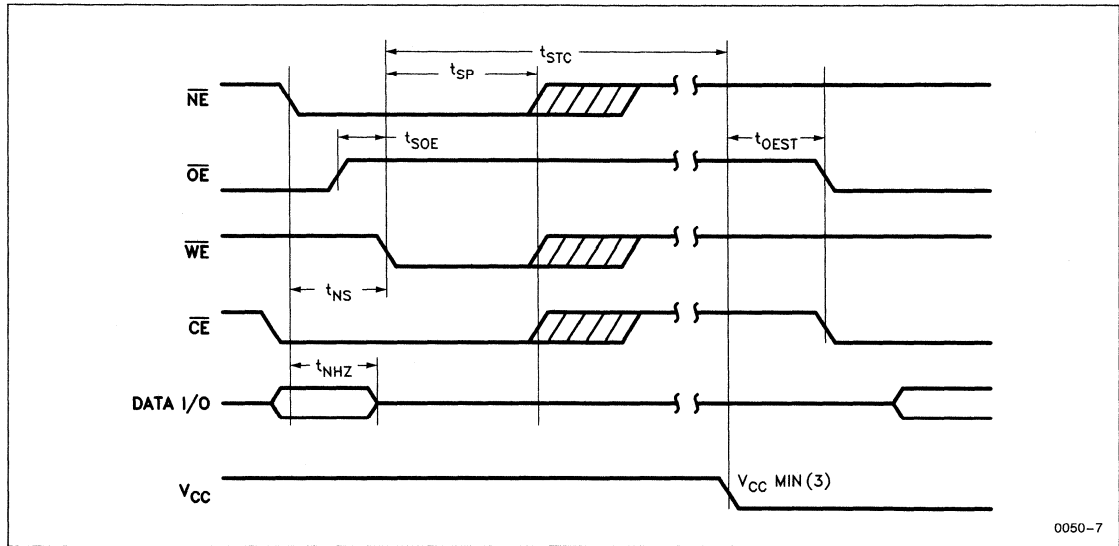
# X2004M

1

## Store Cycle Limits

Symbol	Parameter	X2004M-25		X2004M		Units
		Min.	Max.	Min.	Max.	
$t_{STC}$	Store Cycle Time		10		10	ms
$t_{SP}$	Store Pulse Width	150		200		ns
$t_{NHZ}$	Nonvolatile Enable to Output in High Z		100		100	ns
$t_{OEST}$	Output Enable from End of Store	10		10		ns
$t_{SOE}$	$\overline{OE}$ Disable to Store Function	20		20		ns
$t_{NS}$	$\overline{NE}$ Setup Time from $\overline{WE}$	0		0		ns

## Store Cycle



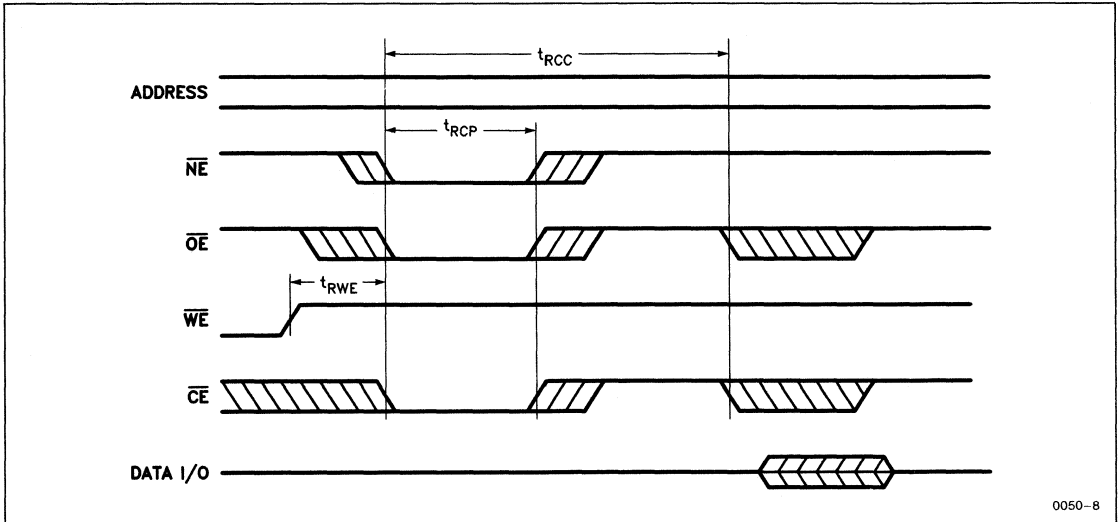
**Note:** (3) X2004M  $V_{CC}$  Min. = 4.5V

# X2004M

## Array Recall Cycle Limits

Symbol	Parameter	X2004M-25		X2004M		Units
		Min.	Max.	Min.	Max.	
$t_{RCC}$	Array Recall Cycle Time		5.0		5.0	$\mu$ s
$t_{RCP}$	Recall Pulse Width to Initiate Recall	150		200		ns
$t_{RWE}$	$\overline{WE}$ Setup Time to $\overline{NE}$	0		0		ns

## Array Recall Cycle



# X2004M

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_8$ )

The address inputs select an 8-bit word during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read and recall operations. Output Enable LOW disables a store operation regardless of the state of  $\overline{CE}$ ,  $\overline{WE}$  or  $\overline{NE}$ .

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2004 through the I/O pins. The I/O pins are placed in the high impedance state when either  $\overline{CE}$  or  $\overline{OE}$  is HIGH or when  $\overline{NE}$  is LOW.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to both the static RAM and stores to the E<sup>2</sup>PROM.

### Nonvolatile Enable ( $\overline{NE}$ )

The Nonvolatile Enable input controls all accesses to the E<sup>2</sup>PROM array (store and recall functions).

## DEVICE OPERATION

The  $\overline{CE}$ ,  $\overline{OE}$ ,  $\overline{WE}$  and  $\overline{NE}$  inputs control the X2004 operation. The X2004 byte-wide NOVRAM uses a 2-line control architecture to eliminate bus contention in a system environment. The I/O bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH, or when  $\overline{NE}$  is LOW.

## RAM OPERATIONS

RAM read and write operations are performed as they would be with any static RAM. A read operation

requires  $\overline{CE}$  and  $\overline{OE}$  to be LOW with  $\overline{WE}$  and  $\overline{NE}$  HIGH. A write operation requires  $\overline{CE}$  and  $\overline{WE}$  to be LOW with  $\overline{NE}$  HIGH. There is no limit to the number of read or write operations performed to the RAM portion of the X2004.

## NONVOLATILE OPERATIONS

With  $\overline{NE}$  LOW, recall and store operations are performed in the same manner as RAM read and write operations. A recall operation causes the entire contents of the E<sup>2</sup>PROM to be written into the RAM array. The time required for the operation to complete is 5  $\mu$ s or less. A store operation causes the entire contents of the RAM array to be stored in the nonvolatile E<sup>2</sup>PROM. The time for the operation to complete is 10 ms or less, typically 5 ms.

## POWER-UP RECALL

Upon power-up ( $V_{CC}$ ), the X2004 performs an automatic array recall. When  $V_{CC}$  minimum is reached, the recall is initiated, regardless of the state of  $\overline{CE}$ ,  $\overline{OE}$ ,  $\overline{WE}$  and  $\overline{NE}$ .

## WRITE PROTECTION

The X2004 has four write protect features that are employed to protect the contents of both the nonvolatile memory and the RAM.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will *not* initiate a write cycle.
- Combined Signal Noise Protection—A combined  $\overline{WE}$  and  $\overline{NE}$  ( $\overline{WE} \bullet \overline{NE}$ ) pulse of less than 20 ns will *not* initiate a store cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 2V$ .
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH,  $\overline{CE}$  HIGH or  $\overline{NE}$  HIGH during power-up or power-down, will prevent an inadvertent store operation.

1

## X2004M






### ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or typical value for the array. Since endurance is limited by the number of electrons trapped in the oxide during data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in the RAM will be "cycled" during a nonvolatile store. This characteristic reduces unneces-

sary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

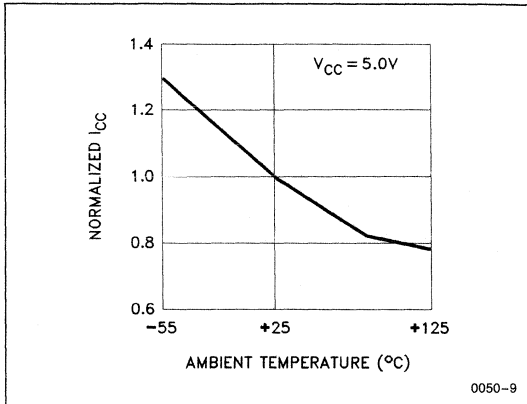
Part Number	Store Cycles	Data Changes Per Bit
X2004M	100,000	10,000

### SYMBOL TABLE

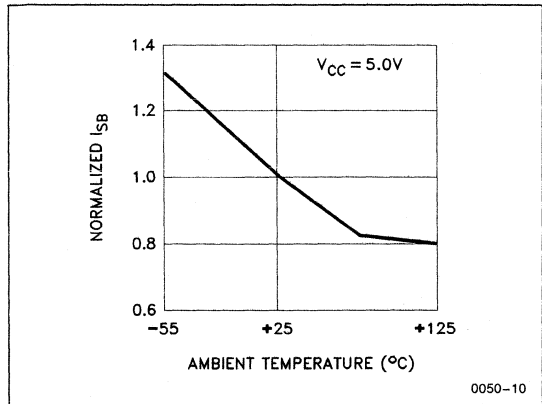
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2004M

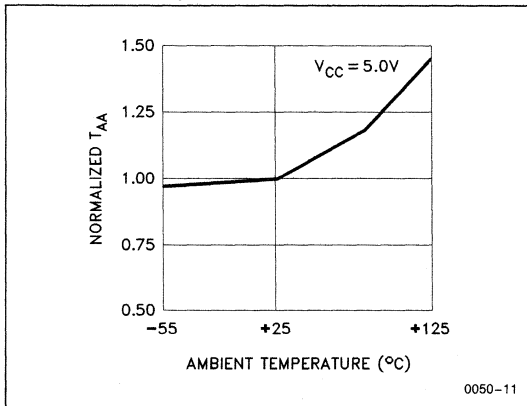
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



1

---

## NOTES

X2444, X2444I .....	2-1
X2444M .....	2-11
X2402, X2402I .....	2-21
X2404, X2404I .....	2-31
X2404M .....	2-41
X24C04, X24C04I .....	2-51
X24C16, X24C16I .....	2-61
X24C16M .....	2-71



**NOVRAM\* Data Sheets**

**1**

**Serial I/O Data Sheets**

**2**





256 Bit      Commercial      X2444      16 x 16 Bit  
 Industrial      X2444I

## Nonvolatile Static RAM

### FEATURES

- Ideal for use with Single Chip Microcomputers
  - Static Timing
  - Minimum I/O Interface
  - Serial Port Compatible (COPS™, 8051)
  - Easily Interfaces to Microcontroller Ports
  - Minimum Support Circuits
- Software and Hardware Control of Nonvolatile Functions
  - Maximum Store Protection
- TTL Compatible
- 16 x 16 Organization
- Low Power Dissipation
  - Active Current: 15 mA Typical
  - Store Current: 8 mA Typical
  - Standby Current: 6 mA Typical
  - Sleep Current: 5 mA Typical
- 8 Pin Mini-DIP Package

### DESCRIPTION

The Xicor X2444 is a serial 256 bit NOVRAM featuring a static RAM configured 16 x 16, overlaid bit for bit with a nonvolatile E<sup>2</sup>PROM array. The X2444 is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V nonvolatile memories.

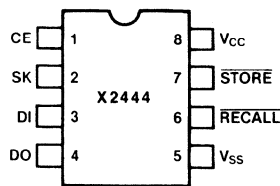
The Xicor NOVRAM design allows data to be transferred between the two memory arrays by means of software commands or external hardware inputs. A store operation (RAM data to E<sup>2</sup>PROM) is completed in 10 ms or less and a recall operation (E<sup>2</sup>PROM data to RAM) is completed in 2.5 μs or less.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM and a minimum 100,000 store operations. Data retention is specified to be greater than 100 years.

COPS™ is a trademark of National Semiconductor Corp.

2

### PIN CONFIGURATION

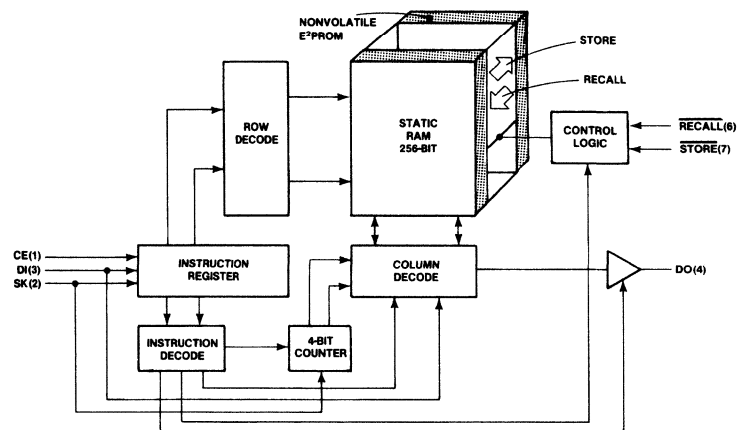


0042-1

### PIN NAMES

CE	Chip Enable
SK	Serial Clock
DI	Serial Data In
DO	Serial Data Out
RECALL	Recall
STORE	Store
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground

### FUNCTIONAL DIAGRAM



0042-2

# X2444, X2444I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2444	-10°C to +85°C
X2444I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2444  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2444I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2444 Limits		X2444I Limits		Units	Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	Power Supply Current		15		25	mA	All Inputs = $V_{CC}$ , $I_{I/O} = 0$ mA
$I_{SL}$	Sleep Current		7		10	mA	
$I_{SB}$	Standby Current		10		15	mA	$CE = V_{IL}$
$I_{STO}$	Store Current		12		15	mA	
$I_{LI}$	Input Load Current		10		10	$\mu\text{A}$	$V_{IN} = V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 0.5$	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 2.4$ mA
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -0.8$ mA

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0$  MHz,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100$ pF

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2444, X2444I

## NONVOLATILE OPERATIONS

Operation	STORE	RECALL	INST	WRITE ENABLE LATCH	Previous RECALL
Hardware Recall	1	0	NOP(2)	X	X
Software Recall	1	1	RCL	X	X
Hardware Store	0	1	NOP(2)	SET	True
Software Store	1	1	STO	SET	True



2

## A.C. CHARACTERISTICS

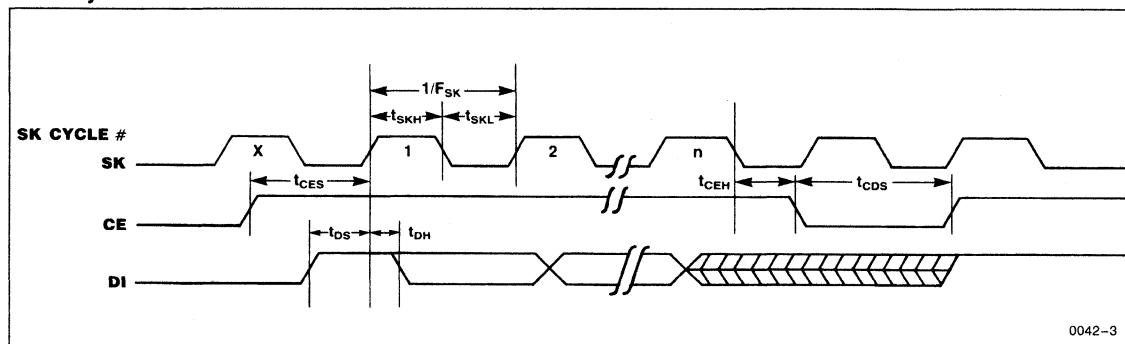
X2444  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2444I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read and Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$F_{SK}$	SK Frequency		1.0	MHz
$t_{SKH}$	SK Positive Pulse Width	0.4		$\mu\text{s}$
$t_{SKL}$	SK Negative Pulse Width	0.4		$\mu\text{s}$
$t_{DS}$	Data Setup Time	0.4		$\mu\text{s}$
$t_{DH}$	Data Hold Time	0.08		$\mu\text{s}$
$t_{PD1}$	SK  to Data 0 Valid		375	ns
$t_{PD}$	SK  to Data Valid		375	ns
$t_z$	Chip Enable to Output High Z		1.0	$\mu\text{s}$
$t_{CES}$	Chip Enable Setup	0.8		$\mu\text{s}$
$t_{CEH}$	Chip Enable Hold	0.4		$\mu\text{s}$
$t_{CDS}$	Chip Deselect	0.8		$\mu\text{s}$

### Write Cycle

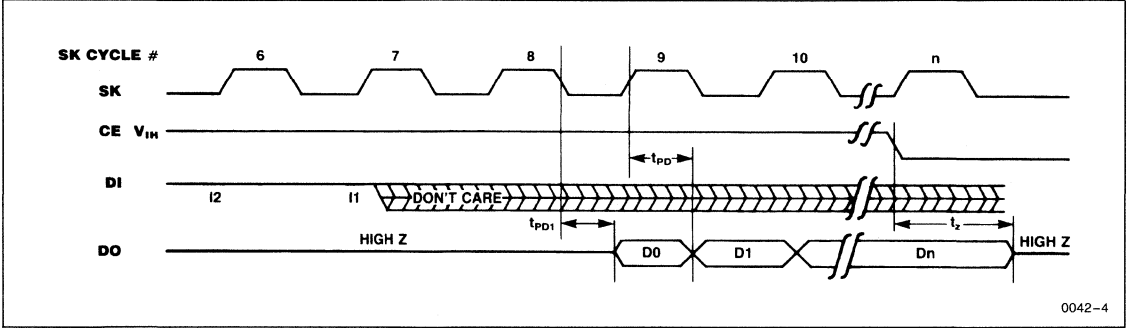


0042-3

Note: (2) NOP designates when the X2444 is not currently executing an instruction.

# X2444, X2444I

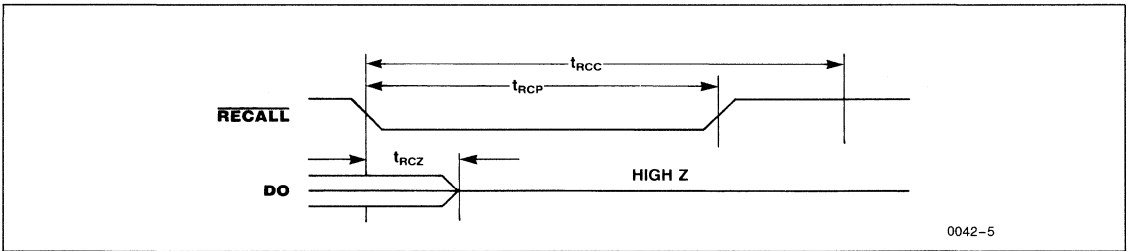
## Read Cycle



## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RCC}$	Recall Cycle Time	2.5		$\mu\text{s}$
$t_{RCP}$	Recall Pulse Width <sup>(3)</sup>	1.0		$\mu\text{s}$
$t_{RCZ}$	Recall to Output High Z		0.5	$\mu\text{s}$

## Recall Cycle



**Note:** (3) Recall rise time must be  $< 10 \mu\text{s}$ .

# X2444, X2444I

## Store Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{ST}$	Store Time		5	10	ms
$t_{STP}$	Store Pulse Width	0.2			$\mu$ S
$t_{STZ}$	Store To Output High Z			1.0	$\mu$ S
$V_{CC}$	Store Inhibit		3		V

## Hardware Store

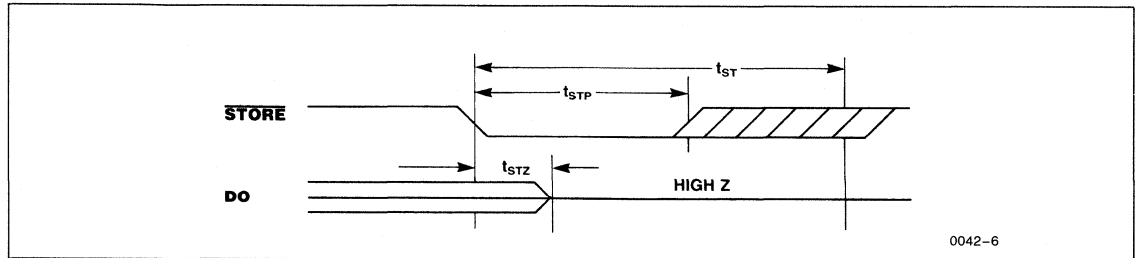
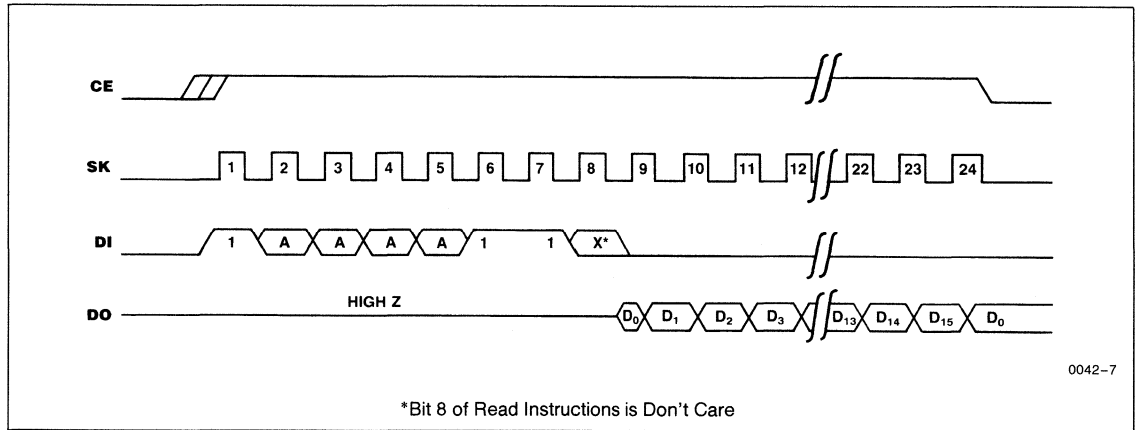


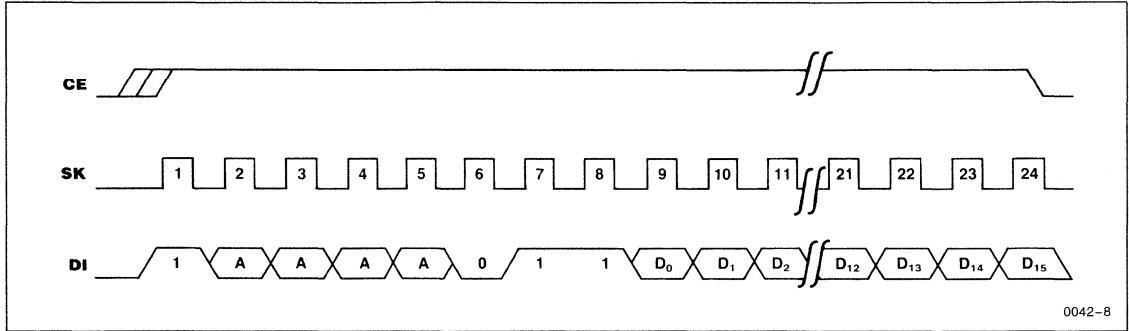
Figure 1: RAM Read



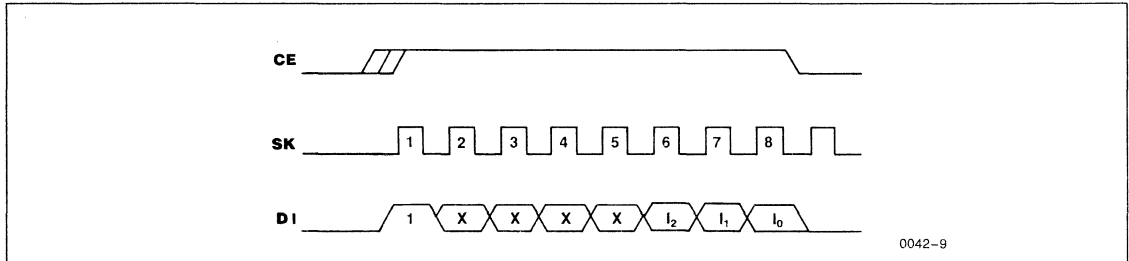
Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X2444, X2444I

**Figure 2: RAM Write**



**Figure 3: Non-Data Operations**



**TABLE 1: INSTRUCTION SET**

Instruction	Format, I <sub>2</sub> I <sub>1</sub> I <sub>0</sub>	Operation
WRDS (Figure 3)	1XXXX000	Reset Write Enable Latch (Disables writes and stores)
STO (Figure 3)	1XXXX001	Store RAM Data in E <sup>2</sup> PROM
SLEEP (Figure 3)	1XXXX010	Enter SLEEP Mode
WRITE (Figure 2)	1AAAA011	Write Data into RAM Address AAAA
WREN (Figure 3)	1XXXX100	Set Write Enable Latch (Enables writes and stores)
RCL (Figure 3)	1XXXX101	Recall E <sup>2</sup> PROM Data into RAM
READ (Figure 1)	1AAAA11X	Read Data from RAM Address AAAA

X = Don't Care  
A = Address Bit

## X2444, X2444I

---

### PIN DESCRIPTIONS

#### Chip Enable (CE)

The Chip Enable input must be HIGH to enable all read/write operations. CE LOW resets the instruction register and places the X2444 in the standby low power mode.

#### Serial Clock (SK)

The Serial Clock input is used to clock all data into and out of the device.

#### Data In (DI)

Data In is the serial data input.

#### Data Out (DO)

Data Out is the serial data output. It is in the high impedance state except during data output cycles in response to a READ instruction.

#### STORE

$\overline{\text{STORE}}$  LOW will initiate an internal transfer of data from RAM to E<sup>2</sup>PROM.

#### RECALL

$\overline{\text{RECALL}}$  LOW will initiate an internal transfer of data from E<sup>2</sup>PROM to RAM.

### DEVICE OPERATION

The X2444 contains an 8-bit instruction register. It is accessed via the DI input, with data being clocked in on the rising edge of SK. CE must be HIGH during the entire data transfer operation.

Table 1 contains a list of the instructions and their operation codes. The most significant bit (MSB) of all instructions is a one, bits 6 through 3 are either RAM address (A) or don't care (X) and bits 2 through 0 are the operation codes. The X2444 requires the instruction to be shifted in with the MSB first.

After CE is HIGH, the X2444 will not begin to interpret the data stream until a one has been shifted in on DI. Therefore, CE may be brought HIGH with SK running and DI LOW. DI must then go HIGH to indicate the start condition of an instruction before the X2444 will begin any action.

In addition, the SK clock is totally static. The user can completely stop the clock and data shifting will be stopped. Restarting the clock will resume shifting of data.

#### WRDS and WREN

Internally the X2444 contains a "write enable" latch. This latch must be set for either writes to the RAM or store operations to the E<sup>2</sup>PROM. The WREN instruction sets the latch and the WRDS instruction resets the latch, disabling *both* RAM writes and E<sup>2</sup>PROM stores. The write enable latch is automatically reset on power-up.

#### SLEEP

The SLEEP instruction removes power from the RAM, placing the X2444 in a very low power quiescent state. Data in the RAM is lost once a SLEEP instruction is issued; however, data from the last store operation is retained in the E<sup>2</sup>PROM. The sleep mode can be exited by either a software or hardware recall operation.

#### RCL and $\overline{\text{RECALL}}$

Either the RCL instruction or a LOW on the  $\overline{\text{RECALL}}$  input will initiate a transfer of E<sup>2</sup>PROM data into RAM. A recall operation must be performed after a power-up before any store or RAM write operation can be enabled. This recall operation and the recall recovery from the sleep mode guarantees a known state of data in RAM. Both recall operations set an internal "previous recall" latch which must be set to enable any write or store operations.

#### STO and $\overline{\text{STORE}}$

Either the STO instruction or a LOW on the  $\overline{\text{STORE}}$  input will initiate the transfer of data from RAM to E<sup>2</sup>PROM. In order to safeguard against unwanted store operations, the following conditions must be true:

1. STO instruction issued or  $\overline{\text{STORE}}$  input is LOW;
2. The internal write enable latch must be set (WREN instruction issued);
3. The "previous recall" latch must be set.

Once the store cycle is initiated, all other device functions are inhibited. Upon completion of the store cycle, the write enable latch is reset.

2

## X2444, X2444I

---

### WRITE

The write instruction contains the 4 bit address of the word to be written. The write instruction is immediately followed by the 16-bit word to be written. CE must remain HIGH during the entire operation. If CE is brought LOW prematurely (after the instruction but before 16 bits of data are transferred), the instruction register will be reset and the data that was shifted in will be written to RAM. If CE is kept HIGH for more than 24 SK clock cycles (8-bit instruction plus 16-bit data) the data already shifted in will be overwritten.

### READ

The read instruction contains the 4 bit address of the word to be accessed. Unlike the other six instructions, I<sub>0</sub> is a “don’t care” for the read instruction. This provides two advantages. In a design that ties both DI and DO together, the absence of an eighth bit in the instruction allows the host time to convert an I/O line from an output to an input. Secondly, it allows for valid data output during the ninth SK clock cycle.

D<sub>0</sub>, the first bit output during a read operation, is truncated. That is, it is internally clocked by the falling edge of the eighth SK clock; whereas, all succeeding bits are clocked by the rising edge of SK (refer to Read Cycle Diagram).

### WRITE PROTECTION

The X2444 provides three hardware and software write protection mechanisms to prevent inadvertent stores of unknown data.

#### Power-Down Condition

(when “write enable” latch and “previous recall” latch are not in the reset state):

- Write Inhibit—Holding either  $\overline{\text{RECALL}}$  LOW, CE LOW or  $\overline{\text{STORE}}$  HIGH during power-down will prevent an inadvertent store.

#### Power-Up Condition

- Write Enable Latch—Upon power-up the “write enable” latch is in the reset state, disabling any store operation.

### Unknown Data Store

- Previous Recall Latch—The “previous recall” latch must be reset after power-up and after exiting the sleep mode. It may be reset only by performing a recall operation, which assures that data in all RAM locations is valid.

### LOW POWER MODES

The X2444 provides two power conservation modes. When CE is LOW, non-critical internal devices are powered-down, placing the device in the standby power mode. Entering the sleep mode removes power from the entire RAM array, placing the device in a very low power quiescent state (sleep mode).

### ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or *typical* value for the array. Since endurance is limited by the number of electrons trapped in the oxide by data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

Part Number	Store Cycles	Data Changes Per Bit
X2444	100,000	10,000
X2444I	100,000	10,000



## X2444, X2444I

### SYSTEM CONSIDERATIONS

#### Power-Down Data Protection

Because the X2444 is a 5V only nonvolatile memory device it may be susceptible to inadvertent writes to the E<sup>2</sup>PROM array during power-down cycles. Power-up cycles are not a problem because the previous recall latch and write enable latch are reset, preventing any possible corruption of E<sup>2</sup>PROM data.

If the  $\overline{\text{STORE}}$  and  $\overline{\text{RECALL}}$  pins are tied to  $V_{CC}$  through a pullup resistor and only software store operations are performed to initiate stores, there is little likelihood of an inadvertent store. However, if these two lines are under microprocessor control, positive action should be employed to negate the possibility of these control lines bouncing and generating an unwanted

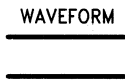




store. The safest method is to issue the WRDS command after a write sequence and also following store operations. Note: an internal store may take up to 10 ms; therefore, the host microprocessor should delay 10 ms after initiating the store prior to issuing the WRDS command.

#### Power-On Recall

The X2444 performs a power-on recall that transfers the E<sup>2</sup>PROM contents to the RAM array. Although the data may be read from the RAM array, this recall does not reset the previous recall latch. During this power-on recall operation, all commands are ignored. Therefore, the host should delay any operation with the X2444 a minimum 2.5  $\mu\text{s}$  ( $t_{RCC}$ ) after  $V_{CC}$  is stable.

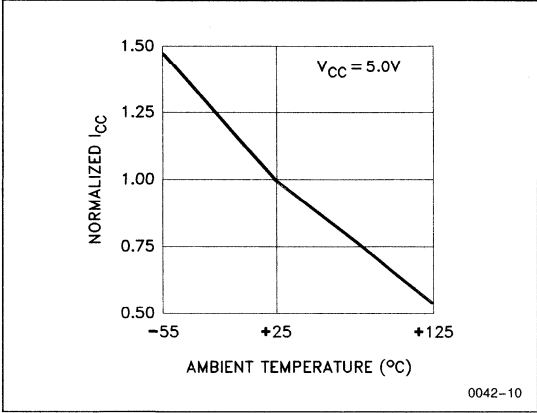
2

### SYMBOL TABLE

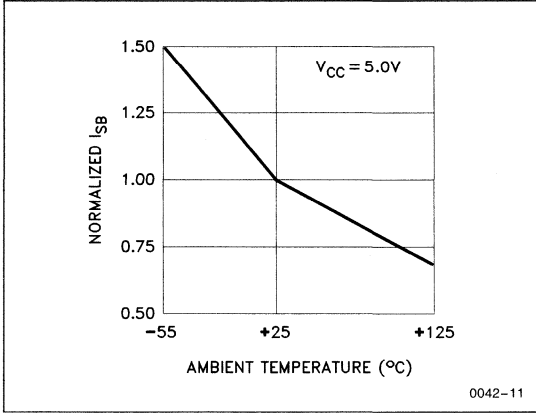
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2444, X2444I

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



## Nonvolatile Static RAM

### FEATURES

- Ideal for use with Single Chip Microcomputers
  - Static Timing
  - Minimum I/O Interface
  - Serial Port Compatible (COPSTM, 8051)
  - Easily Interfaces to Microcontroller Ports
  - Minimum Support Circuits
- Software and Hardware Control of Nonvolatile Functions
  - Maximum Store Protection
- TTL Compatible
- 16 x 16 Organization
- Low Power Dissipation
  - Active Current: 25 mA Typical
  - Store Current: 15 mA Typical
  - Standby Current: 15 mA Typical
  - Sleep Current: 10 mA Typical
- 8 Pin Mini-DIP Package

### DESCRIPTION

The Xicor X2444 is a serial 256 bit NOVRAM featuring a static RAM configured 16 x 16, overlaid bit for bit with a nonvolatile E<sup>2</sup>PROM array. The X2444 is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V nonvolatile memories.

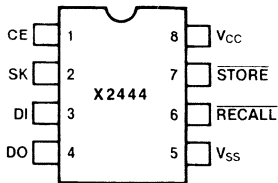
The Xicor NOVRAM design allows data to be transferred between the two memory arrays by means of software commands or external hardware inputs. A store operation (RAM data to E<sup>2</sup>PROM) is completed in 10 ms or less and a recall operation (E<sup>2</sup>PROM data to RAM) is completed in 2.5 μs or less.

Xicor NOVRAMs are designed for unlimited write operations to RAM, either from the host or recalls from E<sup>2</sup>PROM and a minimum 100,000 store operations. Data retention is specified to be greater than 100 years.

COPSTM is a trademark of National Semiconductor Corp.

2

### PIN CONFIGURATION

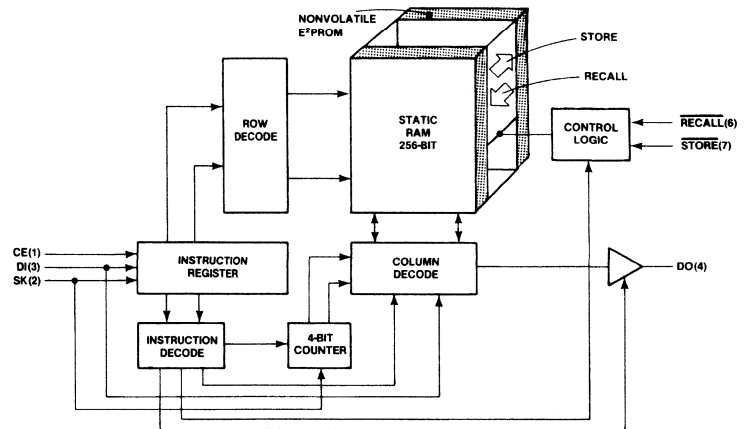


0049-1

### PIN NAMES

CE	Chip Enable
SK	Serial Clock
DI	Serial Data In
DO	Serial Data Out
RECALL	Recall
STORE	Store
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground

### FUNCTIONAL DIAGRAM



0049-2

# X2444M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias .....	-65°C to +135°C
Storage Temperature .....	-65°C to +150°C
Voltage on any Pin with Respect to Ground .....	-1.0V to +7V
D.C. Output Current .....	5 mA
Lead Temperature (Soldering, 10 Seconds) .....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Conditions
		Min.	Max.		
$I_{CC}$	Power Supply Current		25	mA	All Inputs = $V_{CC}$ , $I_{I/O} = 0\text{ mA}$
$I_{SL}$	Sleep Current		10	mA	
$I_{SB}$	Standby Current		15	mA	$CE = V_{IL}$
$I_{STO}$	Store Current		15	mA	
$I_{LI}$	Input Load Current		10	$\mu\text{A}$	$V_{IN} = V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 2.4\text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -0.8\text{ mA}$

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0\text{ MHz}$ , $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2444M

## NONVOLATILE OPERATIONS



Operation	STORE	RECALL	INST	WRITE ENABLE LATCH	Previous RECALL
Hardware Recall	1	0	NOP(2)	X	X
Software Recall	1	1	RCL	X	X
Hardware Store	0	1	NOP(2)	SET	True
Software Store	1	1	STO	SET	True

2

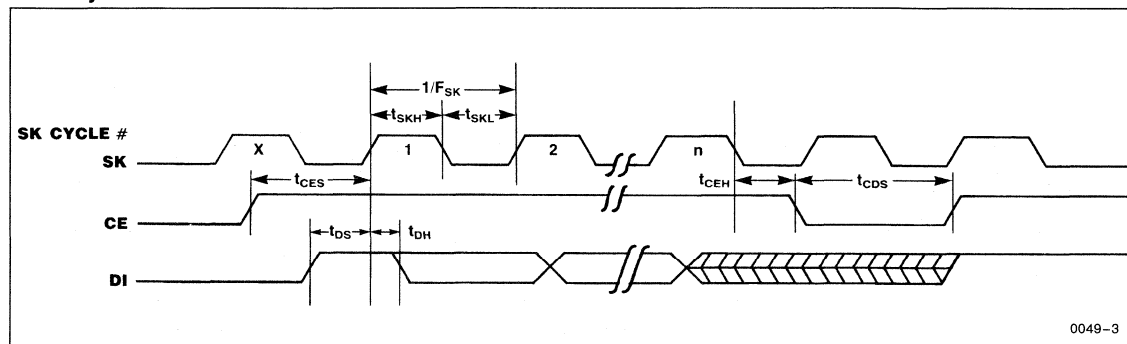
## A.C. CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read and Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$F_{SK}$	SK Frequency		1.0	MHz
$t_{SKH}$	SK Positive Pulse Width	0.4		$\mu\text{s}$
$t_{SKL}$	SK Negative Pulse Width	0.4		$\mu\text{s}$
$t_{DS}$	Data Setup Time	0.4		$\mu\text{s}$
$t_{DH}$	Data Hold Time	0.08		$\mu\text{s}$
$t_{PD1}$	SK  to Data 0 Valid		375	ns
$t_{PD}$	SK  to Data Valid		375	ns
$t_z$	Chip Enable to Output High Z		1.0	$\mu\text{s}$
$t_{CES}$	Chip Enable Setup	0.8		$\mu\text{s}$
$t_{CEH}$	Chip Enable Hold	0.4		$\mu\text{s}$
$t_{CDS}$	Chip Deselect	0.8		$\mu\text{s}$

### Write Cycle

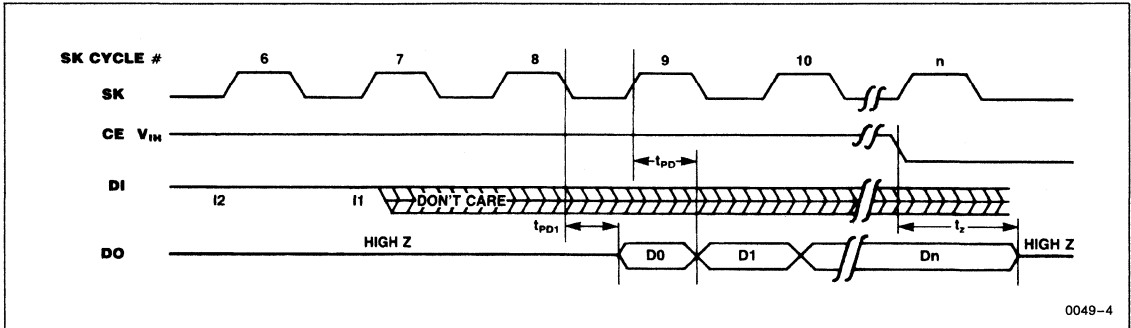


0049-3

Note: (2) NOP designates when the X2444 is not currently executing an instruction.

# X2444M

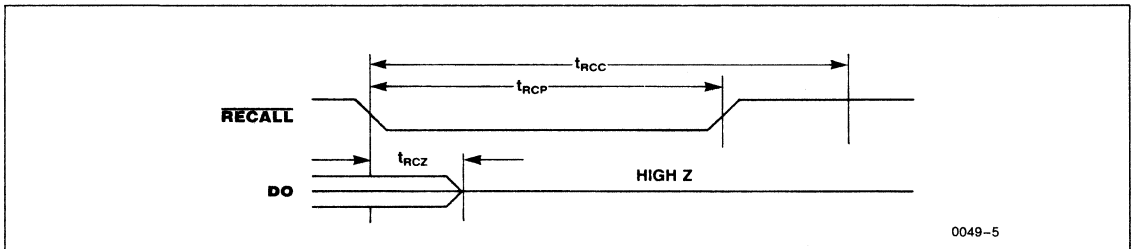
## Read Cycle



## Array Recall Cycle Limits

Symbol	Parameter	Min.	Max.	Units
t <sub>RCC</sub>	Recall Cycle Time	2.5		μs
t <sub>RCP</sub>	Recall Pulse Width <sup>(3)</sup>	1.0		μs
t <sub>RCZ</sub>	Recall to Output High Z		0.5	μs

## Recall Cycle



**Note:** (3) Recall rise time must be < 10 μs.

# X2444M

## Store Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{ST}$	Store Time		5	10	ms
$t_{STP}$	Store Pulse Width	0.2			$\mu$ s
$t_{STZ}$	Store To Output High Z			1.0	$\mu$ s
$V_{CC}$	Store Inhibit		3		V

2

## Hardware Store

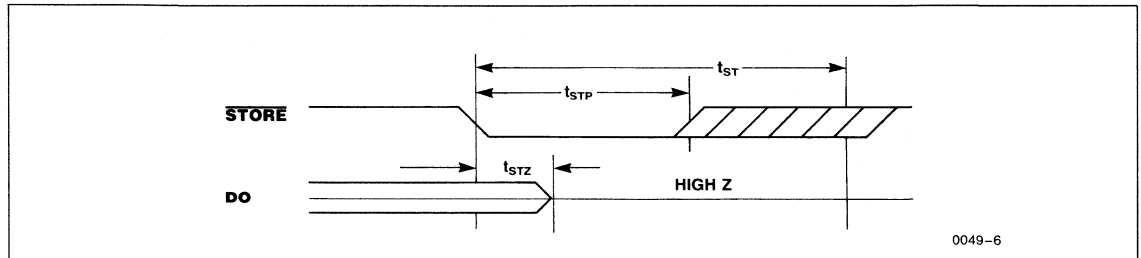
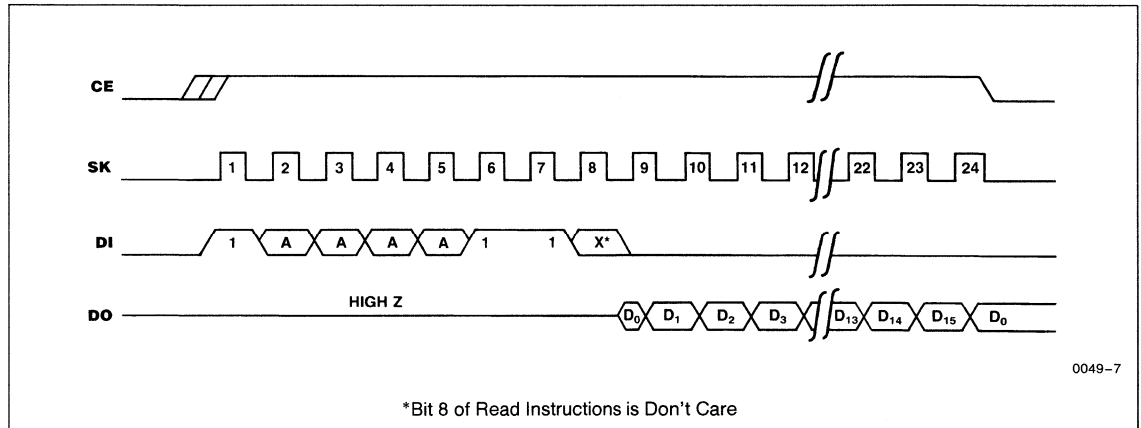


Figure 1: RAM Read

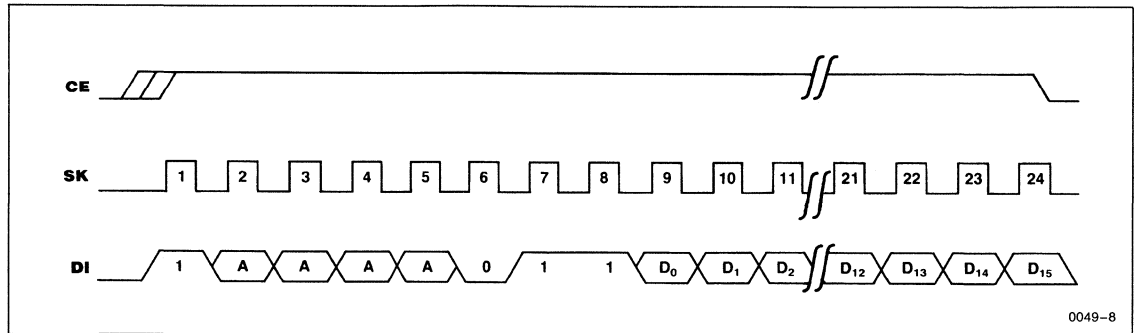


\*Bit 8 of Read Instructions is Don't Care

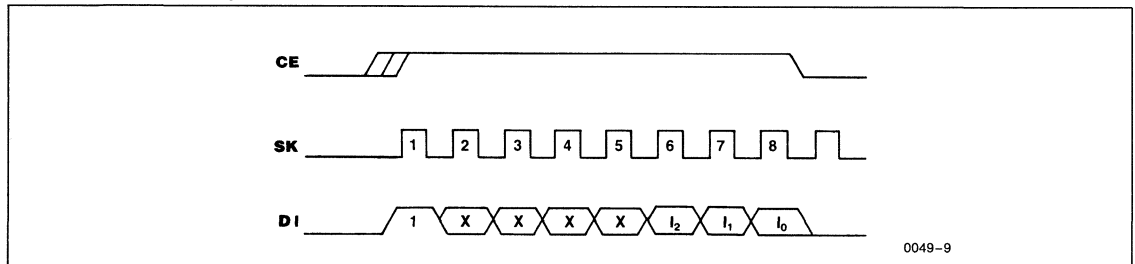
**Note:** (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X2444M

**Figure 2: RAM Write**



**Figure 3: Non-Data Operations**



**TABLE 1: INSTRUCTION SET**

Instruction	Format, I <sub>2</sub> I <sub>1</sub> I <sub>0</sub>	Operation
WRDS (Figure 3)	1XXXX000	Reset Write Enable Latch (Disables writes and stores)
STO (Figure 3)	1XXXX001	Store RAM Data in E <sup>2</sup> PROM
SLEEP (Figure 3)	1XXXX010	Enter SLEEP Mode
WRITE (Figure 2)	1AAAA011	Write Data into RAM Address AAAA
WREN (Figure 3)	1XXXX100	Set Write Enable Latch (Enables writes and stores)
RCL (Figure 3)	1XXXX101	Recall E <sup>2</sup> PROM Data into RAM
READ (Figure 1)	1AAAA11X	Read Data from RAM Address AAAA

X = Don't Care  
A = Address Bit



# X2444M

---

## PIN DESCRIPTIONS

### Chip Enable (CE)

The Chip Enable input must be HIGH to enable all read/write operations. CE LOW resets the instruction register and places the X2444 in the standby low power mode.

### Serial Clock (SK)

The Serial Clock input is used to clock all data into and out of the device.

### Data In (DI)

Data In is the serial data input.

### Data Out (DO)

Data Out is the serial data output. It is in the high impedance state except during data output cycles in response to a READ instruction.

### STORE

$\overline{\text{STORE}}$  LOW will initiate an internal transfer of data from RAM to E<sup>2</sup>PROM.

### RECALL

$\overline{\text{RECALL}}$  LOW will initiate an internal transfer of data from E<sup>2</sup>PROM to RAM.

## DEVICE OPERATION

The X2444 contains an 8-bit instruction register. It is accessed via the DI input, with data being clocked in on the rising edge of SK. CE must be HIGH during the entire data transfer operation.

Table 1 contains a list of the instructions and their operation codes. The most significant bit (MSB) of all instructions is a one, bits 6 through 3 are either RAM address (A) or don't care (X) and bits 2 through 0 are the operation codes. The X2444 requires the instruction to be shifted in with the MSB first.

After CE is HIGH, the X2444 will not begin to interpret the data stream until a one has been shifted in on DI. Therefore, CE may be brought HIGH with SK running and DI LOW. DI must then go HIGH to indicate the start condition of an instruction before the X2444 will begin any action.

In addition, the SK clock is totally static. The user can completely stop the clock and data shifting will be stopped. Restarting the clock will resume shifting of data.

### WRDS and WREN

Internally the X2444 contains a "write enable" latch. This latch must be set for either writes to the RAM or store operations to the E<sup>2</sup>PROM. The WREN instruction sets the latch and the WRDS instruction resets the latch, disabling *both* RAM writes and E<sup>2</sup>PROM stores. The write enable latch is automatically reset on power-up.

### SLEEP

The SLEEP instruction removes power from the RAM, placing the X2444 in a very low power quiescent state. Data in the RAM is lost once a SLEEP instruction is issued; however, data from the last store operation is retained in the E<sup>2</sup>PROM. The sleep mode can be exited by either a software or hardware recall operation.

### RCL and RECALL

Either the RCL instruction or a LOW on the  $\overline{\text{RECALL}}$  input will initiate a transfer of E<sup>2</sup>PROM data into RAM. A recall operation must be performed after a power-up before any store or RAM write operation can be enabled. This recall operation and the recall recovery from the sleep mode guarantees a known state of data in RAM. Both recall operations set an internal "previous recall" latch which must be set to enable any write or store operations.

### STO and STORE

Either the STO instruction or a LOW on the  $\overline{\text{STORE}}$  input will initiate the transfer of data from RAM to E<sup>2</sup>PROM. In order to safeguard against unwanted store operations, the following conditions must be true:

1. STO instruction issued or  $\overline{\text{STORE}}$  input is LOW;
2. The internal write enable latch must be set (WREN instruction issued);
3. The "previous recall" latch must be set.

Once the store cycle is initiated, all other device functions are inhibited. Upon completion of the store cycle, the write enable latch is reset.

2

# X2444M

---

## WRITE

The write instruction contains the 4 bit address of the word to be written. The write instruction is immediately followed by the 16-bit word to be written. CE must remain HIGH during the entire operation. If CE is brought LOW prematurely (after the instruction but before 16 bits of data are transferred), the instruction register will be reset and the data that was shifted in will be written to RAM. If CE is kept HIGH for more than 24 SK clock cycles (8-bit instruction plus 16-bit data) the data already shifted in will be overwritten.

## READ

The read instruction contains the 4 bit address of the word to be accessed. Unlike the other six instructions,  $I_0$  is a “don’t care” for the read instruction. This provides two advantages. In a design that ties both DI and DO together, the absence of an eighth bit in the instruction allows the host time to convert an I/O line from an output to an input. Secondly, it allows for valid data output during the ninth SK clock cycle.

DO, the first bit output during a read operation, is truncated. That is, it is internally clocked by the falling edge of the eighth SK clock; whereas, all succeeding bits are clocked by the rising edge of SK (refer to Read Cycle Diagram).

## WRITE PROTECTION

The X2444 provides three hardware and software write protection mechanisms to prevent inadvertent stores of unknown data.

### Power-Down Condition

(when “write enable” latch and “previous recall” latch are not in the reset state):

- Write Inhibit—Holding either  $\overline{\text{RECALL}}$  LOW, CE LOW or  $\overline{\text{STORE}}$  HIGH during power-down will prevent an inadvertent store.

### Power-Up Condition

- Write Enable Latch—Upon power-up the “write enable” latch is in the reset state, disabling any store operation.

## Unknown Data Store

- Previous Recall Latch—The “previous recall” latch must be reset after power-up and after exiting the sleep mode. It may be reset only by performing a recall operation, which assures that data in all RAM locations is valid.

## LOW POWER MODES

The X2444 provides two power conservation modes. When CE is LOW, non-critical internal devices are powered-down, placing the device in the standby power mode. Entering the sleep mode removes power from the entire RAM array, placing the device in a very low power quiescent state (sleep mode).

## ENDURANCE

The endurance specification of a device is characterized by the predicted *first* bit failure to occur in the entire memory (device or system) array rather than the average or *typical* value for the array. Since endurance is limited by the number of electrons trapped in the oxide by data changes, Xicor NOVRAMs are designed to minimize the number of changes an E<sup>2</sup>PROM bit cell undergoes during store operations. Only those bits in the E<sup>2</sup>PROM that are different from their corresponding location in RAM will be “cycled” during a nonvolatile store. This characteristic reduces unnecessary cycling of any of the rest of the bits in the array, thereby increasing the potential endurance of each bit and increasing the potential endurance of the entire array. Reliability data documented in RR504, the *Xicor Reliability Report on Endurance*, and additional reports are available from Xicor.

Part Number	Store Cycles	Data Changes Per Bit
X2444M	100,000	10,000

# X2444M

## SYSTEM CONSIDERATIONS

### Power-Down Data Protection

Because the X2444 is a 5V only nonvolatile memory device it may be susceptible to inadvertent writes to the E<sup>2</sup>PROM array during power-down cycles. Power-up cycles are not a problem because the previous recall latch and write enable latch are reset, preventing any possible corruption of E<sup>2</sup>PROM data.

If the  $\overline{\text{STORE}}$  and  $\overline{\text{RECALL}}$  pins are tied to  $V_{CC}$  through a pullup resistor and only software store operations are performed to initiate stores, there is little likelihood of an inadvertent store. However, if these two lines are under microprocessor control, positive action should be employed to negate the possibility of these control lines bouncing and generating an unwanted

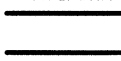




store. The safest method is to issue the WRDS command after a write sequence and also following store operations. Note: an internal store may take up to 10 ms; therefore, the host microprocessor should delay 10 ms after initiating the store prior to issuing the WRDS command.

### Power-On Recall

The X2444 performs a power-on recall that transfers the E<sup>2</sup>PROM contents to the RAM array. Although the data may be read from the RAM array, this recall does not reset the previous recall latch. During this power-on recall operation, all commands are ignored. Therefore, the host should delay any operation with the X2444 a minimum 2.5  $\mu\text{s}$  ( $t_{PCC}$ ) after  $V_{CC}$  is stable.

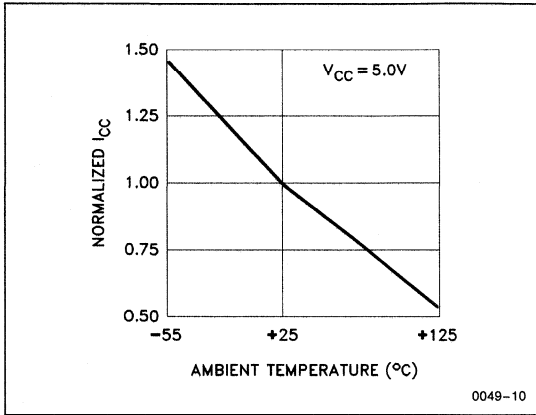
2

### SYMBOL TABLE

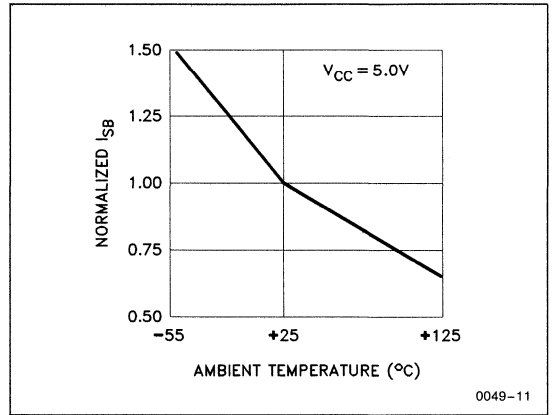
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2444M

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**2K**      **Commercial**  
**Industrial**

**X2402**  
**X2402I**

**256 x 8 Bit**

## Electrically Erasable PROM

### TYPICAL FEATURES

- Internally Organized 256 x 8
- 2 Wire Serial Interface
- Provides Bidirectional Data Transfer Protocol
- Eight Byte Page Write Mode  
—Minimizes Total Write Time Per Byte
- Self Timed Write Cycle  
—Typical Write Cycle Time of 5 ms
- Data Retention Greater Than 100 Years
- 8 Pin Mini-DIP Package

### DESCRIPTION

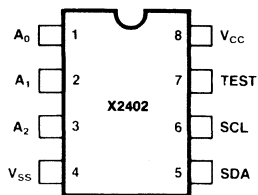
The X2402 is a 2048 bit serial E<sup>2</sup>PROM, internally organized as one 256 x 8 page. The X2402 is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories.

The X2402 features a serial interface and software protocol allowing operation on a two wire bus.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to RR504 for further endurance information. Data retention is specified to be greater than 100 years.

**2**

### PIN CONFIGURATION

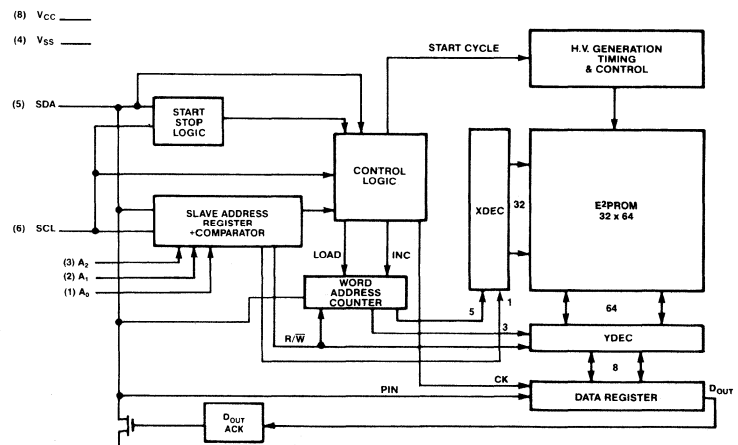


0035-1

### PIN NAMES

1 to 3	A <sub>0</sub> to A <sub>2</sub> Address Inputs
4	V <sub>SS</sub>
5	SDA Serial Data
6	SCL Serial Clock
7	Test Input → to V <sub>SS</sub>
8	V <sub>CC</sub>

### FUNCTIONAL DIAGRAM



0035-2

# X2402, X2402I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2402	-10°C to +85°C
X2402I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to $V_{SS}$	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2402  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

X2402I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2402 Limits			X2402I Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.	Min.	Typ.(1)	Max.		
$I_{CC}$	Power Supply Current		20	30		20	35	mA	$f_{SCL} = 100\text{ KHz}$
$I_{SB}$	Standby Current		15	25		15	30	mA	
$I_{LI}$	Input Leakage Current		0.1	10		0.1	10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		0.1	10		0.1	10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$I_{TP}(2)$	Test Pin Pull Down Current		16	30		16	30	$\mu\text{A}$	$V_{IN} = V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 0.5$	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4			0.4	V	$I_{OL} = 3\text{ mA}$

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0\text{ MHz}$ , $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}(3)$	Input/Output Capacitance (SDA)	8	pF	$V_{I/O} = 0V$
$C_{IN}(3)$	Input Capacitance ( $A_0, A_1, A_2, SCL$ )	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) Test pin has on chip pull down device which sinks 16  $\mu\text{A}$  (typical) to  $V_{SS}$ .

(3) This parameter is periodically sampled and not 100% tested.

# X2402, X2402I

## A.C. CHARACTERISTICS

X2402  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2402I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read & Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$f_{\text{SCL}}$	SCL Clock Frequency	0	100	KHz
$T_I$	Noise Suppression Time Constant at SCL, SDA Inputs		100	ns
$t_{\text{AA}}$	SCL Low to SDA Data Out and ACK Out		3.5	$\mu\text{s}$
$t_{\text{BUF}}$	Time the Bus Must be Free Before a New Transmission Can Start	4.7		$\mu\text{s}$
$t_{\text{HD:STA}}$	Start Condition Hold Time	4.0		$\mu\text{s}$
$t_{\text{LOW}}$	Clock Low Period	4.7		$\mu\text{s}$
$t_{\text{HIGH}}$	Clock High Period	4.0		$\mu\text{s}$
$t_{\text{SU:STA}}$	Start Condition Setup Time (for a Repeated Start Condition)	4.7		$\mu\text{s}$
$t_{\text{HD:DAT}}$	Data In Hold Time	0		$\mu\text{s}$
$t_{\text{SU:DAT}}$	Data In Setup Time	250		ns
$t_{\text{R}}$	SDA and SCL Rise Time		1	$\mu\text{s}$
$t_{\text{F}}$	SDA and SCL Fall Time		300	ns
$t_{\text{SU:STO}}$	Stop Condition Setup Time	4.7		$\mu\text{s}$
$t_{\text{DH}}$	Data Out Hold Time	300		ns

2

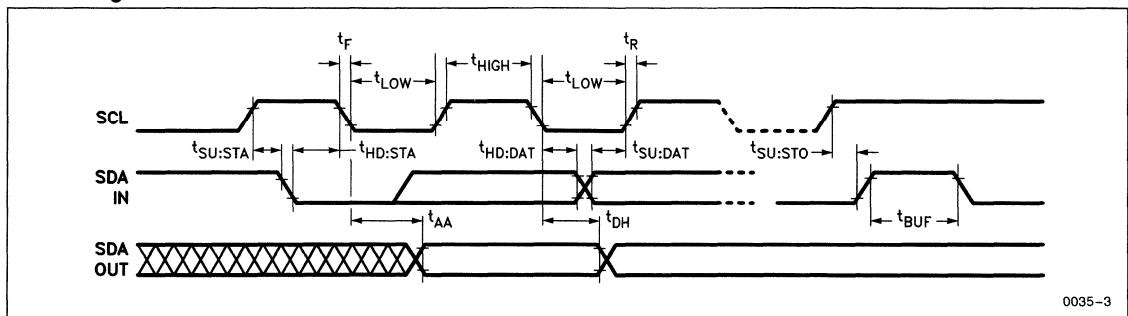
### Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{\text{WR}}$	Write Cycle Time		5	10	ms

The write cycle time is the time from a valid stop condition of a write sequence to the end of the internal erase/program cycle. During the write cycle, the X2402

bus interface circuits are disabled, SDA is allowed to remain high, and the device does not respond to its slave address.

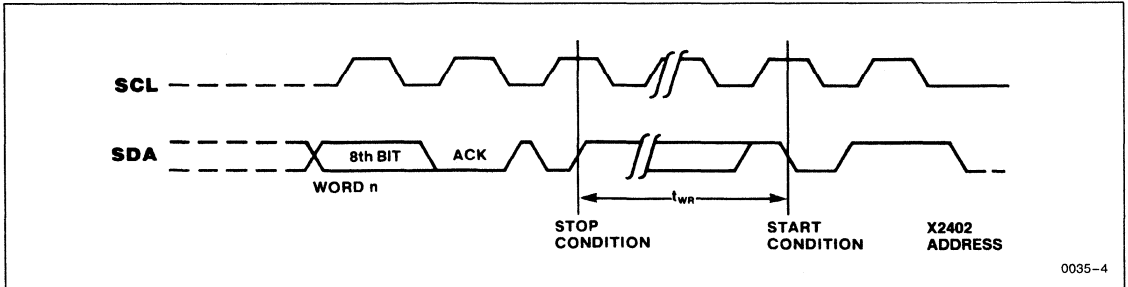
### Bus Timing



**Note:** (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X2402, X2402I

## Write Cycle Timing



## PIN DESCRIPTIONS

### Serial Clock (SCL)

The SCL input is used to clock all data into and out of the device.

### Serial Data (SDA)

SDA is a bidirectional pin used to transfer data into and out of the device. It is an open drain output and may be wire-ORed with any number of open drain or open collector outputs.

### Address ( $A_0$ , $A_1$ , $A_2$ )

The Address inputs are used to set the least significant three bits of the seven bit slave address. The inputs are static, and should be tied HIGH or LOW, forming one unique address per device.

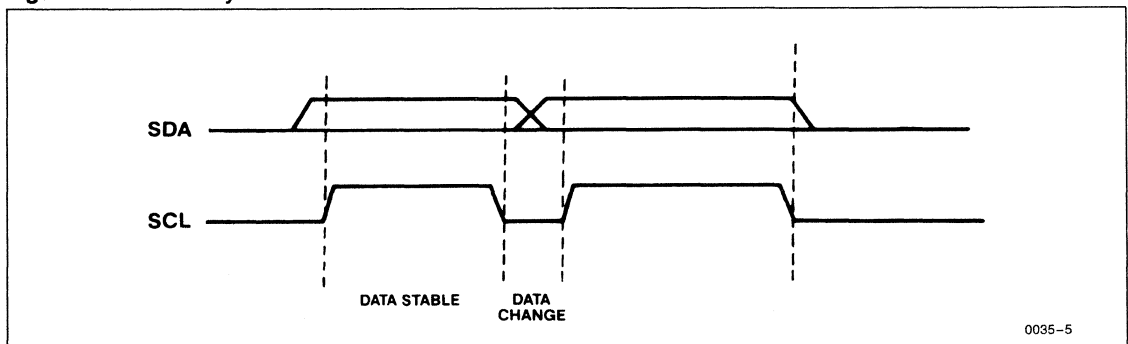
## DEVICE OPERATION

The X2402 supports a bidirectional bus oriented protocol. The protocol defines any device that sends data onto the bus as a transmitter, and the receiving device as the receiver. The device controlling the transfer is a master and the device being controlled is the slave. The master will always initiate data transfers, and provide the clock for both transmit and receive operations. Therefore, the X2402 will be considered a slave in all applications.

### Clock and Data Conventions

Data states on the SDA line can change only during SCL LOW. SDA state changes during SCL HIGH are reserved for indication start and stop conditions. Refer to Figures 1 and 2.

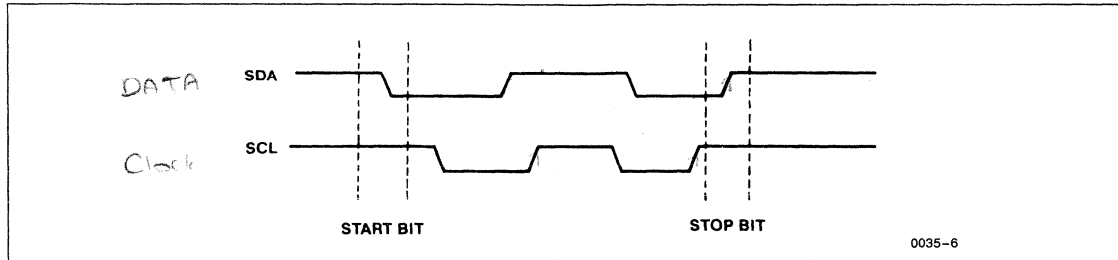
Figure 1: Data Validity





## X2402, X2402I

Figure 2: Definition of Start and Stop



### Start Condition

All commands are preceded by the start condition, which is a HIGH to LOW transition of SDA when SCL is HIGH. The X2402 continuously monitors the SDA and SCL lines for the start condition and will not respond to any command until this condition has been met.

### Stop Condition

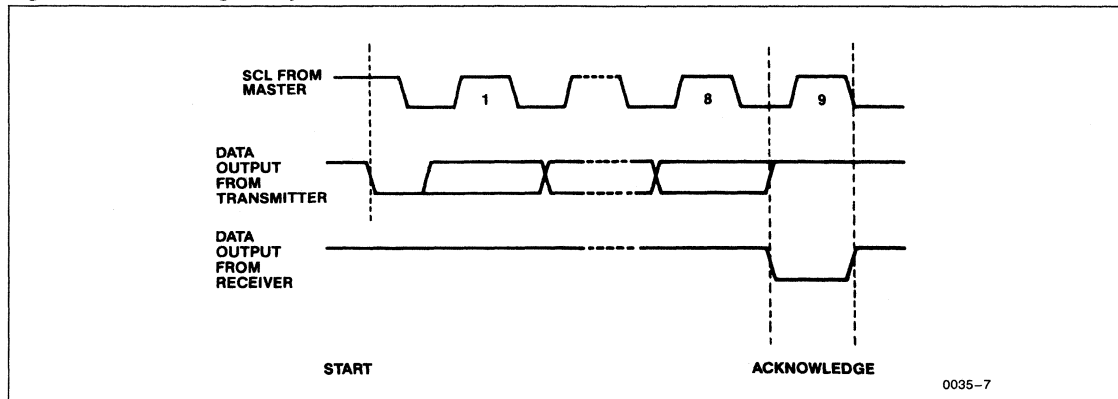
All communications are terminated by a stop condition, which is a LOW to HIGH transition of SDA when SCL is HIGH.

### Acknowledge

Acknowledge is a software convention used to indicate successful data transfers. The transmitting device, either master or slave, will release the bus after transmitting eight bits. During the ninth clock cycle the receiver will pull the SDA line LOW to acknowledge that it received the eight bits of data. Refer to Figure 3.

The X2402 will always respond with an acknowledge after recognition of a start condition and its slave address. If both the device and a write operation have been selected, the X2402 will respond with an acknowledge after the receipt of each subsequent eight bit word.

Figure 3: Acknowledge Response from Receiver



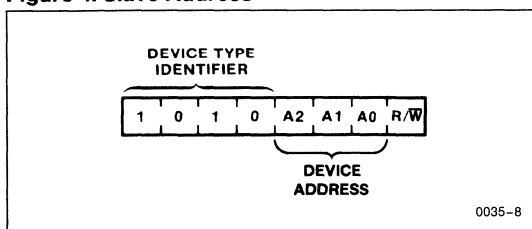
## X2402, X2402I

In the read mode the X2402 will transmit eight bits of data, release the SDA line and monitor the line for an acknowledge. If an acknowledge is detected and no stop condition is generated by the master, the X2402 will continue to transmit data. If an acknowledge is not detected, the X2402 will terminate further data transmissions and await the stop condition.

### DEVICE ADDRESSING

Following a start condition the bus master must output the address of the slave it is accessing. The most significant four bits of the slave address are the device type identifier (see Figure 4). For the X2402 this is fixed as 1010[B].

Figure 4: Slave Address



The next three significant bits address a particular device. A system could have up to eight X2402 devices on the bus (see Figure 10). The eight addresses are defined by the state of the  $A_0$ ,  $A_1$  and  $A_2$  inputs.

The last bit of the slave address defines the operation to be performed. When set to one a read operation is selected; when set to zero a write operation is selected.

Following the start condition, the X2402 monitors the SDA bus comparing the slave address being transmitted with its address (device type and state of  $A_0$ ,  $A_1$  and  $A_2$  inputs). Upon a compare the X2402 outputs an acknowledge on the SDA line. Depending on the state of the R/W bit, the X2402 will execute a read or write operation.

### WRITE OPERATIONS

#### Byte Write

For a write operation, the X2402 requires a second address field. This address field is the word address, comprised of eight bits, providing access to any one of the 256 words of memory. Upon receipt of the word address the X2402 responds with an acknowledge and awaits the next eight bits of data, again responding with an acknowledge. The master then terminates the transfer by generating a stop condition, at which time the X2402 begins the internal write cycle to the nonvolatile memory. While the internal write cycle is in progress the X2402 inputs are disabled, and the device will not respond to any requests from the master. Refer to Figure 5 for the address, acknowledge and data transfer sequence.

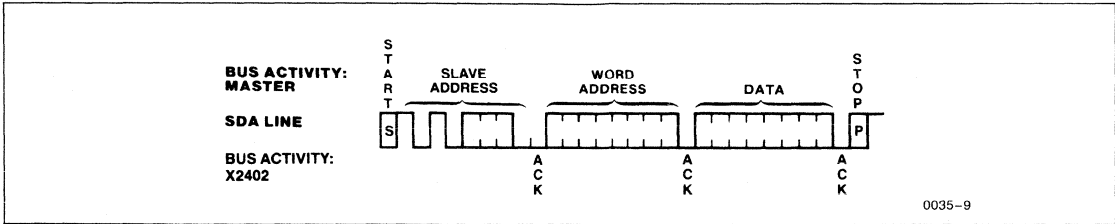
#### Page Write

The X2402 is capable of an eight byte page write operation. It is initiated in the same manner as the byte write operation, but instead of terminating the write cycle after the first data word is transferred, the master can transmit up to seven more words. After the receipt of each word, the X2402 will respond with an acknowledge.

After the receipt of each word, the three low order address bits are internally incremented by one. The high order five bits of the address remain constant. If the master should transmit more than eight words prior to generating the stop condition, the address counter will "roll over" and the previously written data will be overwritten. As with the byte write operation, all inputs are disabled until completion of the internal write cycle. Refer to Figure 6 for the address, acknowledge and data transfer sequence.

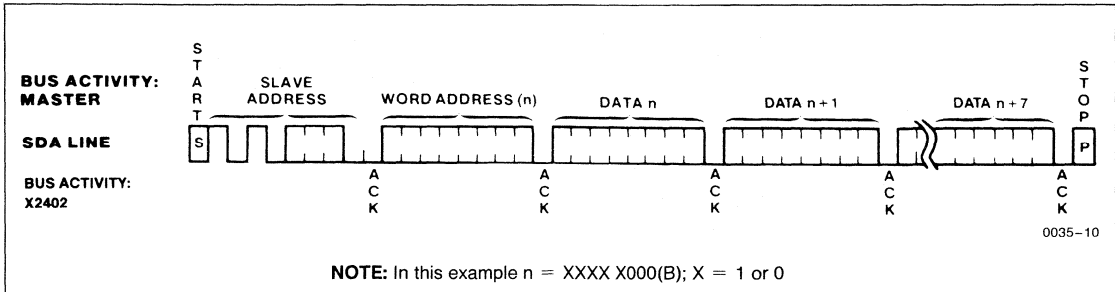
# X2402, X2402I

Figure 5: Byte Write



2

Figure 6: Page Write



## Acknowledge Polling

The disabling of the inputs can be used to take advantage of the typical 5 ms write cycle time. Once the stop condition is issued to indicate the end of the host's write operation the X2402 initiates the internal write cycle. ACK polling can be initiated immediately. This involves issuing the start condition followed by the slave address for a write operation. If the X2402 is still busy with the write operation no ACK will be returned. If the X2402 has completed the write operation an ACK will be returned and the host can then proceed with the next read or write operation.

## READ OPERATIONS

Read operations are initiated in the same manner as write operations with the exception that the  $R/\bar{W}$  bit of

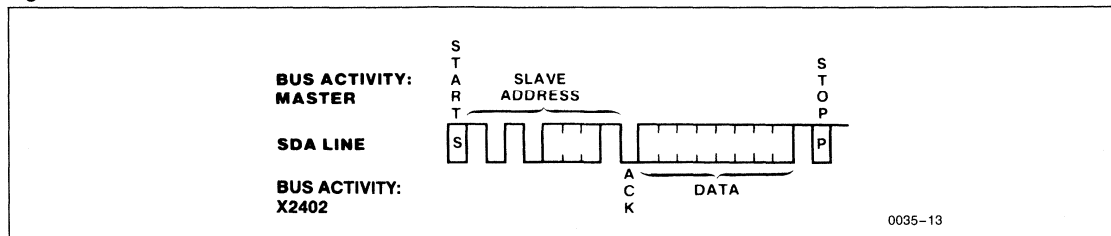
the slave address is set to a one. There are three basic read operations: current address read, random read and sequential read.

## Current Address Read

Internally the X2402 contains an address counter that maintains the address of the last word accessed, incremented by one. Therefore, if the last access (either a read or write) was to address  $n$ , the next read operation would access data from address  $n + 1$ . Upon receipt of the slave address with  $R/\bar{W}$  set to one, the X2402 issues an acknowledge and transmits the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X2402 discontinues transmission. Refer to Figure 7 for the sequence of address, acknowledge and data transfer.

# X2402, X2402I

Figure 7: Current Address Read



## Random Read

Random read operations allow the master to access any memory location in a random manner. Prior to issuing the slave address with the R/W bit set to one, the master must first perform a “dummy” write operation. The master issues the start condition, and the slave address followed by the word address it is to read. After the word address acknowledge, the master immediately reissues the start condition and the slave address with the R/W bit set to one. This will be followed by an acknowledge from the X2402 and then by the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X2402 discontinues transmission. Refer to Figure 8 for the address, acknowledge and data transfer sequence.

## Sequential Read

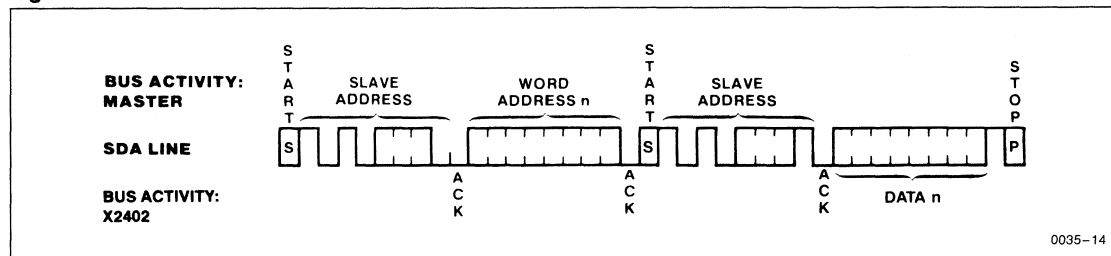
Sequential reads can be initiated as either a current address read or random access read. The first word is transmitted as with the other read modes, however, the master now responds with an acknowledge, indicating it requires additional data. The X2402 continues to output data for each acknowledge received. The read operation is terminated by the master not responding with an acknowledge and generating a stop condition.

The data output is sequential, with the data from address  $n$  followed by the data from  $n + 1$ . The address counter for read operations increments all eight address bits, allowing the entire memory contents of the current 256 word page to be serially read during one operation. If more than 256 words are read, the counter “rolls over” and the X2402 continues to output data from the same 256 word page for each acknowledge received. Refer to Figure 9 for the address, acknowledge and data transfer sequence.

## ENDURANCE

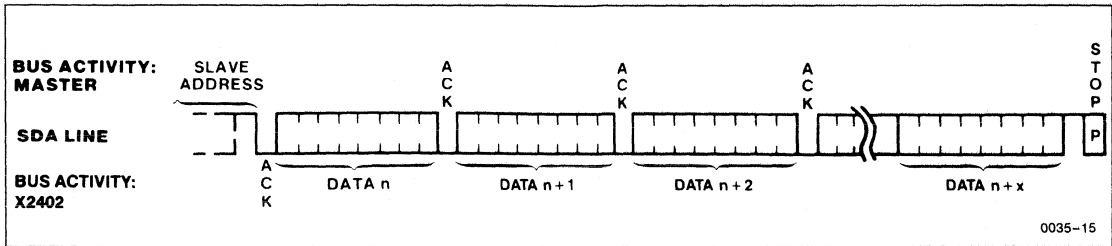
Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately  $1/2$  million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

Figure 8: Random Read



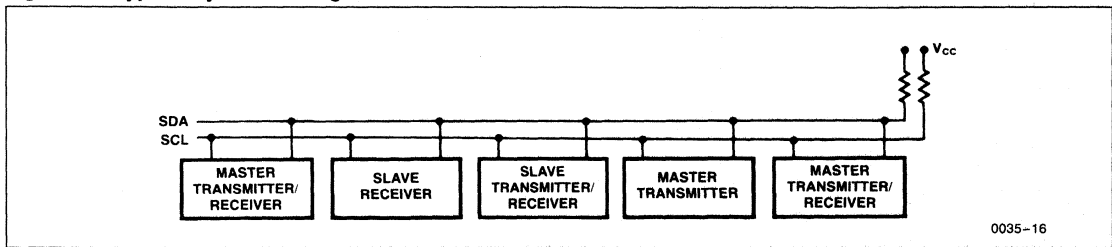
# X2402, X2402I

Figure 9: Sequential Read



2

Figure 10: Typical System Configuration

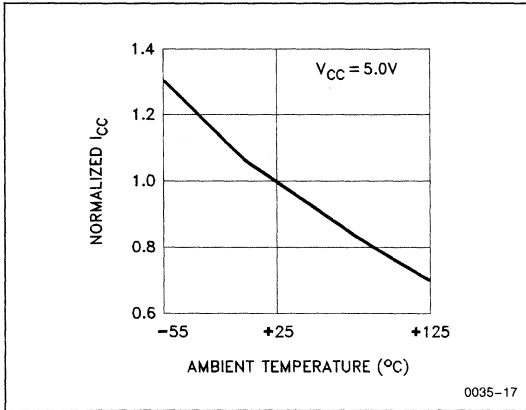


## SYMBOL TABLE

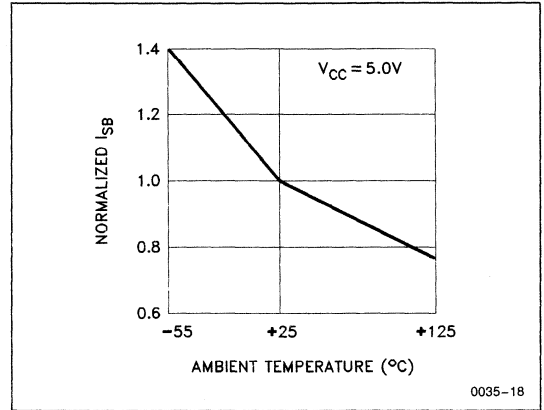
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2402, X2402I

**Normalized Active Supply Current  
vs. Ambient Temperature**



**Normalized Standby Supply Current  
vs. Ambient Temperature**



4K

Commercial  
Industrial

X2404  
X2404I

512 x 8 Bit

## Electrically Erasable PROM

### TYPICAL FEATURES

- Internally Organized as Two Pages  
—Each 256 x 8
- 2 Wire Serial Interface
- Provides Bidirectional Data Transfer Protocol
- Eight Byte Page Write Mode  
—Minimizes Total Write Time Per Byte
- Self Timed Write Cycle  
—Typical Write Cycle Time of 5 ms
- Data Retention Greater Than 100 Years
- 8 Pin Mini-DIP Package

### DESCRIPTION

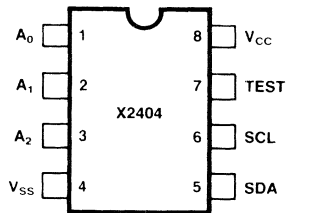
The X2404 is a 4096 bit serial E<sup>2</sup>PROM, internally organized as two 256 x 8 pages. The X2404 is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories.

The X2404 features a serial interface and software protocol allowing operation on a two wire bus.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to RR504 for further endurance information. Data retention is specified to be greater than 100 years.

2

### PIN CONFIGURATION

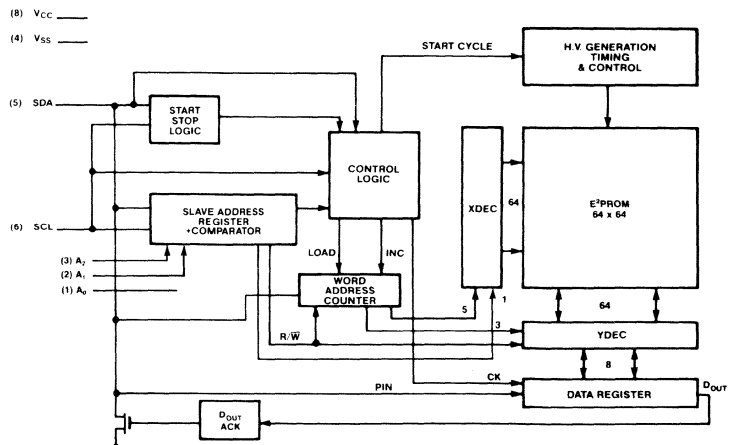


0041-1

### PIN NAMES

1 to 3	A <sub>0</sub> to A <sub>2</sub> Address Inputs
4	V <sub>SS</sub>
5	SDA Serial Data
6	SCL Serial Clock
7	Test Input → to V <sub>SS</sub>
8	V <sub>CC</sub>

### FUNCTIONAL DIAGRAM



0041-2

# X2404, X2404I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2404	-10°C to +85°C
X2404I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to V <sub>SS</sub>	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2404 T<sub>A</sub> = 0°C to +70°C, V<sub>CC</sub> = +5V ± 5%, unless otherwise specified.

X2404I T<sub>A</sub> = -40°C to +85°C, V<sub>CC</sub> = +5V ± 10%, unless otherwise specified.

Symbol	Parameter	X2404 Limits			X2404I Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.	Min.	Typ.(1)	Max.		
I <sub>CC</sub>	Power Supply Current		20	30		20	35	mA	f <sub>SCL</sub> = 100 KHz
I <sub>SB</sub>	Standby Current		15	25		15	30	mA	
I <sub>LI</sub>	Input Leakage Current		0.1	10		0.1	10	μA	V <sub>IN</sub> = GND to V <sub>CC</sub>
I <sub>LO</sub>	Output Leakage Current		0.1	10		0.1	10	μA	V <sub>OUT</sub> = GND to V <sub>CC</sub>
I <sub>TP</sub> (2)	Test Pin Pull Down Current		16	30		16	30	μA	V <sub>IN</sub> = V <sub>CC</sub>
V <sub>IL</sub>	Input Low Voltage	-1.0		0.8	-1.0		0.8	V	
V <sub>IH</sub>	Input High Voltage	2.0		V <sub>CC</sub> + 0.5	2.0		V <sub>CC</sub> + 1.0	V	
V <sub>OL</sub>	Output Low Voltage			0.4			0.4	V	I <sub>OL</sub> = 3 mA

**CAPACITANCE** T<sub>A</sub> = 25°C, f = 1.0 MHz, V<sub>CC</sub> = 5V

Symbol	Test	Max.	Units	Conditions
C <sub>I/O</sub> (3)	Input/Output Capacitance (SDA)	8	pF	V <sub>I/O</sub> = 0V
C <sub>IN</sub> (3)	Input Capacitance (A <sub>0</sub> , A <sub>1</sub> , A <sub>2</sub> , SCL)	6	pF	V <sub>IN</sub> = 0V

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and C <sub>L</sub> = 100 pF

**Notes:** (1) Typical values are for T<sub>A</sub> = 25°C and nominal supply voltage.

(2) Test pin has on chip pull down device which sinks 16 μA (typical) to V<sub>SS</sub>.

(3) This parameter is periodically sampled and not 100% tested.



# X2404, X2404I

## A.C. CHARACTERISTICS

X2404  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2404I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read & Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$f_{\text{SCL}}$	SCL Clock Frequency	0	100	KHz
$T_I$	Noise Suppression Time Constant at SCL, SDA Inputs		100	ns
$t_{\text{AA}}$	SCL Low to SDA Data Out and ACK Out		3.5	$\mu\text{s}$
$t_{\text{BUF}}$	Time the Bus Must be Free Before a New Transmission Can Start	4.7		$\mu\text{s}$
$t_{\text{HD:STA}}$	Start Condition Hold Time	4.0		$\mu\text{s}$
$t_{\text{LOW}}$	Clock Low Period	4.7		$\mu\text{s}$
$t_{\text{HIGH}}$	Clock High Period	4.0		$\mu\text{s}$
$t_{\text{SU:STA}}$	Start Condition Setup Time (for a Repeated Start Condition)	4.7		$\mu\text{s}$
$t_{\text{HD:DAT}}$	Data In Hold Time	0		$\mu\text{s}$
$t_{\text{SU:DAT}}$	Data In Setup Time	250		ns
$t_{\text{R}}$	SDA and SCL Rise Time		1	$\mu\text{s}$
$t_{\text{F}}$	SDA and SCL Fall Time		300	ns
$t_{\text{SU:STO}}$	Stop Condition Setup Time	4.7		$\mu\text{s}$
$t_{\text{DH}}$	Data Out Hold Time	300		ns

2

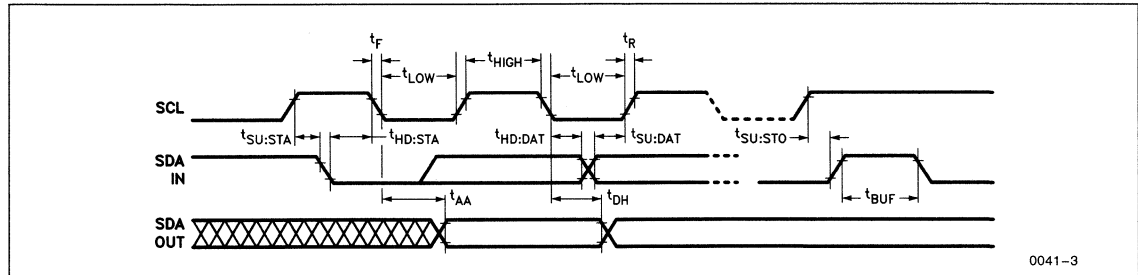
### Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{\text{WR}}$	Write Cycle Time		5	10	ms

The write cycle time is the time from a valid stop condition of a write sequence to the end of the internal erase/program cycle. During the write cycle, the X2404

bus interface circuits are disabled, SDA is allowed to remain high, and the device does not respond to its slave address.

### Bus Timing

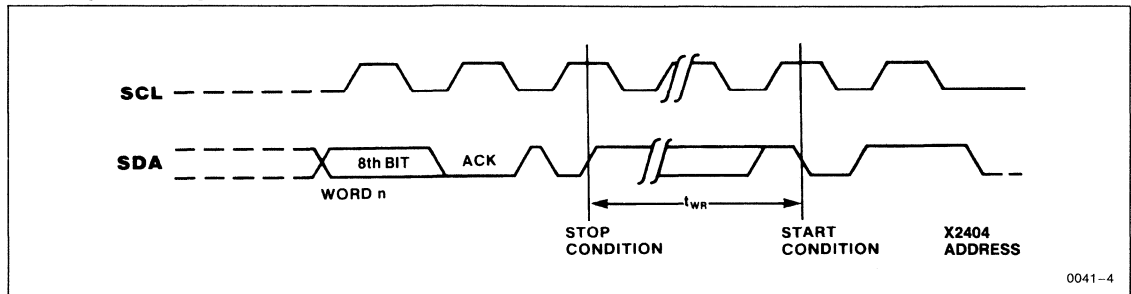


0041-3

Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X2404, X2404I

## Write Cycle Timing



## PIN DESCRIPTIONS

### Serial Clock (SCL)

The SCL input is used to clock all data into and out of the device.

### Serial Data (SDA)

SDA is a bidirectional pin used to transfer data into and out of the device. It is an open drain output and may be wire-ORed with any number of open drain or open collector outputs.

### Address ( $A_0$ )

$A_0$  is unused by the X2404, however, it must be tied to  $V_{SS}$  to ensure proper device operation.

### Address ( $A_1, A_2$ )

The Address inputs are used to set the least significant two bits of the six bit slave address. The inputs are static, and should be tied HIGH or LOW, forming one unique address per device.

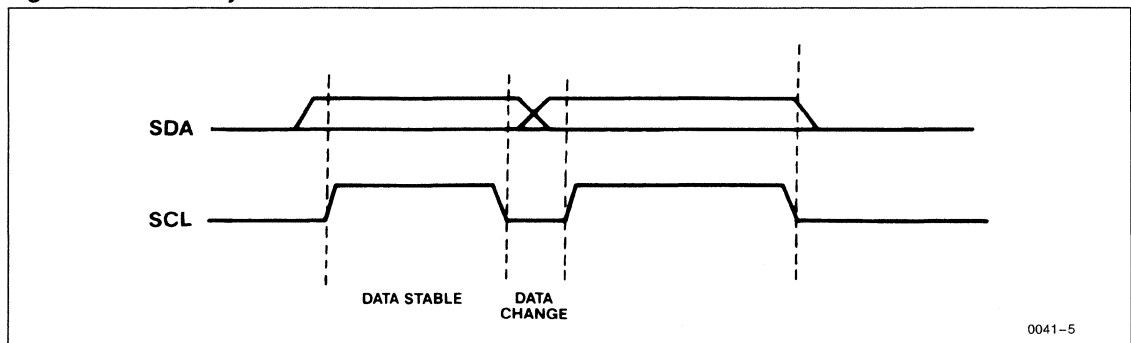
## DEVICE OPERATION

The X2404 supports a bidirectional bus oriented protocol. The protocol defines any device that sends data onto the bus as a transmitter, and the receiving device as the receiver. The device controlling the transfer is a master and the device being controlled is the slave. The master will always initiate data transfers, and provide the clock for both transmit and receive operations. Therefore, the X2404 will be considered a slave in all applications.

### Clock and Data Conventions

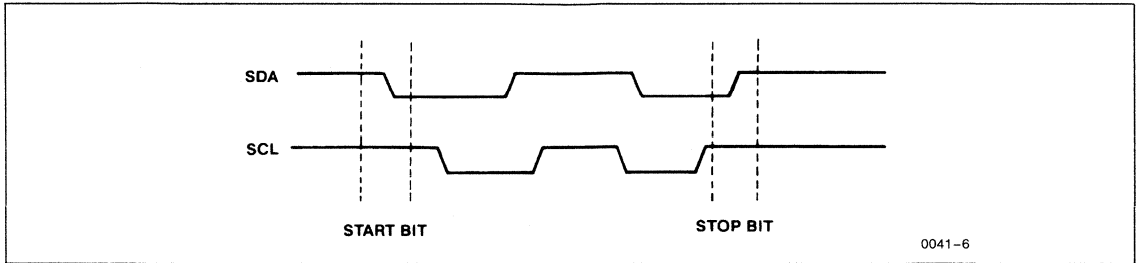
Data states on the SDA line can change only during SCL LOW. SDA state changes during SCL HIGH are reserved for indication start and stop conditions. Refer to Figures 1 and 2.

Figure 1: Data Validity



# X2404, X2404I

Figure 2: Definition of Start and Stop



2

### Start Condition

All commands are preceded by the start condition, which is a HIGH to LOW transition of SDA when SCL is HIGH. The X2404 continuously monitors the SDA and SCL lines for the start condition and will not respond to any command until this condition has been met.

### Stop Condition

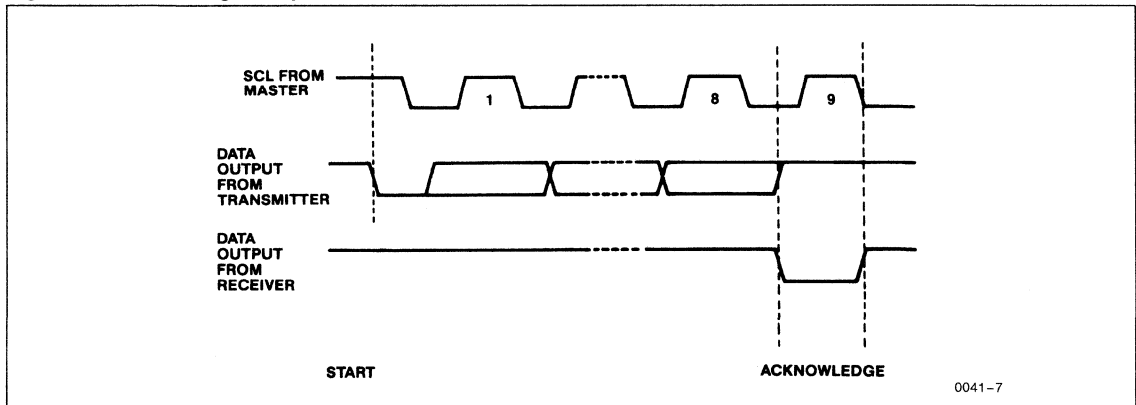
All communications are terminated by a stop condition, which is a LOW to HIGH transition of SDA when SCL is HIGH.

### Acknowledge

Acknowledge is a software convention used to indicate successful data transfers. The transmitting device, either master or slave, will release the bus after transmitting eight bits. During the ninth clock cycle the receiver will pull the SDA line LOW to acknowledge that it received the eight bits of data. Refer to Figure 3.

The X2404 will always respond with an acknowledge after recognition of a start condition and its slave address. If both the device and a write operation have been selected, the X2404 will respond with an acknowledge after the receipt of each subsequent eight bit word.

Figure 3: Acknowledge Response from Receiver



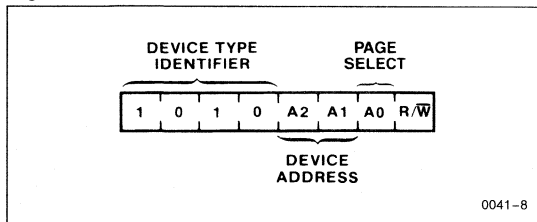
## X2404, X2404I

In the read mode the X2404 will transmit eight bits of data, release the SDA line and monitor the line for an acknowledge. If an acknowledge is detected and no stop condition is generated by the master, the X2404 will continue to transmit data. If an acknowledge is not detected, the X2404 will terminate further data transmissions and await the stop condition.

### DEVICE ADDRESSING

Following a start condition the bus master must output the address of the slave it is accessing. The most significant four bits of the slave address are the device type identifier (see Figure 4). For the X2404 this is fixed as 1010[B].

Figure 4: Slave Address



The next two significant bits address a particular device. A system could have up to four X2404 devices on the bus (see Figure 10). The four addresses are defined by the state of the A<sub>1</sub> and A<sub>2</sub> inputs.

The next bit of the slave address field (bit 1) is the page select bit. It is used by the host to toggle between the two 256 word pages of memory.

The last bit of the slave address defines the operation to be performed. When set to one a read operation is selected; when set to zero a write operation is selected.

Following the start condition, the X2404 monitors the SDA bus comparing the slave address being transmitted with its address (device type and state of A<sub>1</sub> and A<sub>2</sub> inputs). Upon a compare the X2404 outputs an acknowledge on the SDA line. Depending on the state of the R/W bit, the X2404 will execute a read or write operation.

### WRITE OPERATIONS

#### Byte Write

For a write operation, the X2404 requires a second address field. This address field is the word address, comprised of eight bits, providing access to any one of the 256 words of memory. Upon receipt of the word address the X2404 responds with an acknowledge and awaits the next eight bits of data, again responding with an acknowledge. The master then terminates the transfer by generating a stop condition, at which time the X2404 begins the internal write cycle to the nonvolatile memory. While the internal write cycle is in progress the X2404 inputs are disabled, and the device will not respond to any requests from the master. Refer to Figure 5 for the address, acknowledge and data transfer sequence.

#### Page Write

The X2404 is capable of an eight byte page write operation. It is initiated in the same manner as the byte write operation, but instead of terminating the write cycle after the first data word is transferred, the master can transmit up to seven more words. After the receipt of each word, the X2404 will respond with an acknowledge.

After the receipt of each word, the three low order address bits are internally incremented by one. The high order five bits of the address remain constant. If the master should transmit more than eight words prior to generating the stop condition, the address counter will "roll over" and the previously written data will be overwritten. As with the byte write operation, all inputs are disabled until completion of the internal write cycle. Refer to Figure 6 for the address, acknowledge and data transfer sequence.

# X2404, X2404I

Figure 5: Byte Write

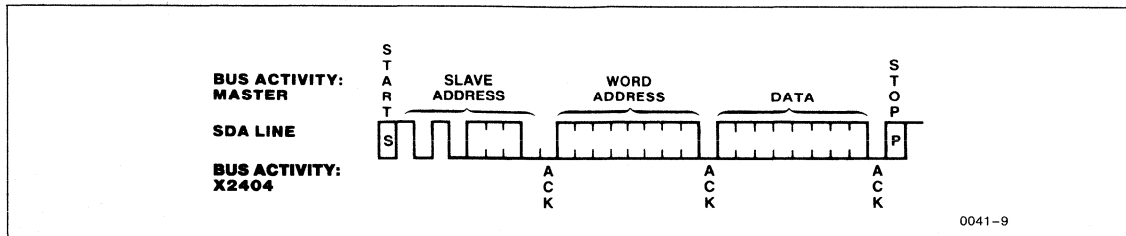
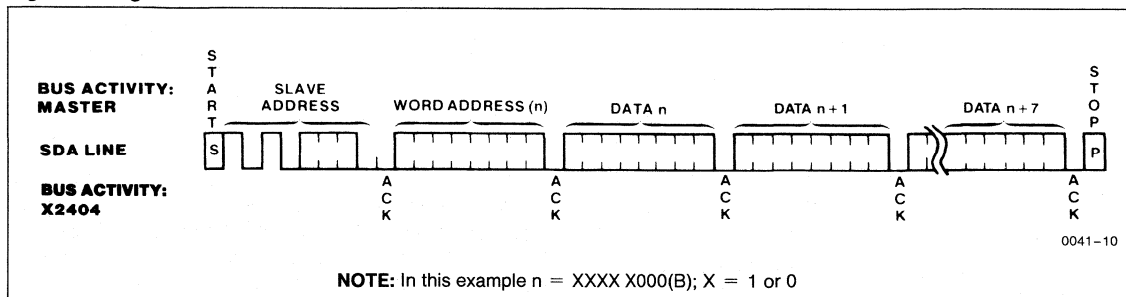


Figure 6: Page Write



## Acknowledge Polling

The disabling of the inputs can be used to take advantage of the typical 5 ms write cycle time. Once the stop condition is issued to indicate the end of the host's write operation the X2404 initiates the internal write cycle. ACK polling can be initiated immediately. This involves issuing the start condition followed by the slave address for a write operation. If the X2404 is still busy with the write operation no ACK will be returned. If the X2404 has completed the write operation an ACK will be returned and the host can then proceed with the next read or write operation.

## READ OPERATIONS

Read operations are initiated in the same manner as write operations with the exception that the  $R/\bar{W}$  bit of

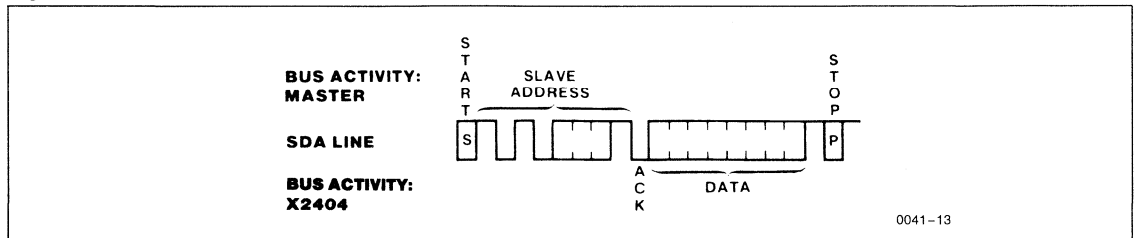
the slave address is set to a one. There are three basic read operations: current address read, random read and sequential read.

## Current Address Read

Internally the X2404 contains an address counter that maintains the address of the last word accessed, incremented by one. Therefore, if the last access (either a read or write) was to address  $n$ , the next read operation would access data from address  $n + 1$ . Upon receipt of the slave address with  $R/\bar{W}$  set to one, the X2404 issues an acknowledge and transmits the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X2404 discontinues transmission. Refer to Figure 7 for the sequence of address, acknowledge and data transfer.

# X2404, X2404I

Figure 7: Current Address Read



## Random Read

Random read operations allow the master to access any memory location in a random manner. Prior to issuing the slave address with the R/W bit set to one, the master must first perform a “dummy” write operation. The master issues the start condition, and the slave address followed by the word address it is to read. After the word address acknowledge, the master immediately reissues the start condition and the slave address with the R/W bit set to one. This will be followed by an acknowledge from the X2404 and then by the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X2404 discontinues transmission. Refer to Figure 8 for the address, acknowledge and data transfer sequence.

## Sequential Read

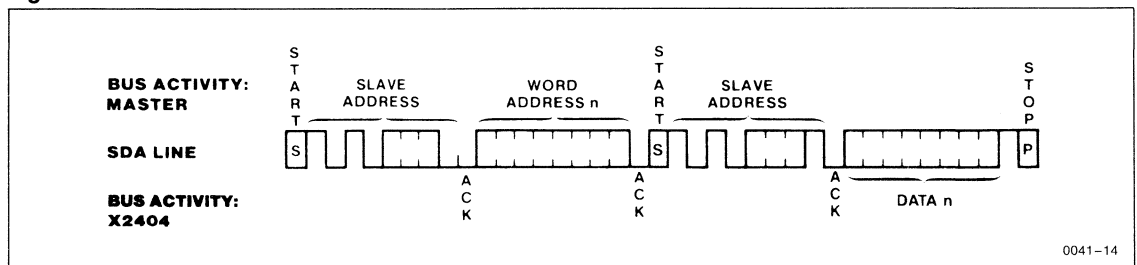
Sequential reads can be initiated as either a current address read or random access read. The first word is transmitted as with the other read modes, however, the master now responds with an acknowledge, indicating it requires additional data. The X2404 continues to output data for each acknowledge received. The read operation is terminated by the master not responding with an acknowledge and generating a stop condition.

The data output is sequential, with the data from address  $n$  followed by the data from  $n + 1$ . The address counter for read operations increments all eight address bits, allowing the entire memory contents of the current 256 word page to be serially read during one operation. If more than 256 words are read, the counter “rolls over” and the X2404 continues to output data from the same 256 word page for each acknowledge received. Refer to Figure 9 for the address, acknowledge and data transfer sequence.

## ENDURANCE

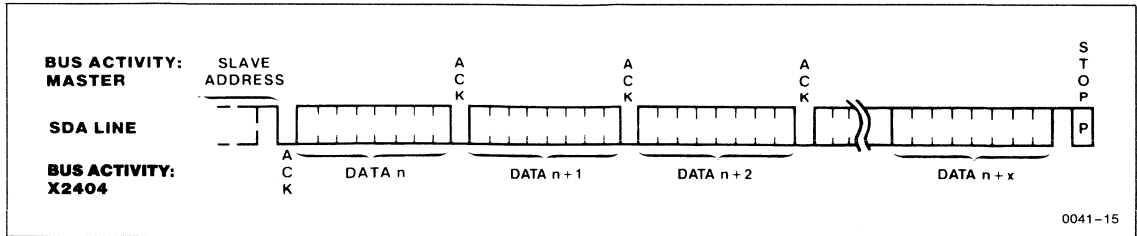
Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

Figure 8: Random Read



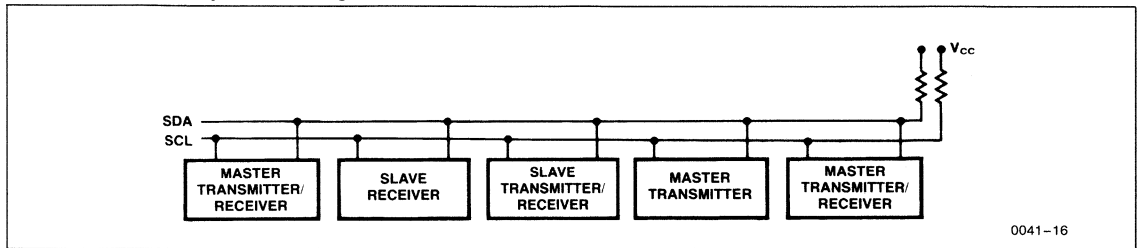
# X2404, X2404I

Figure 9: Sequential Read



2

Figure 10: Typical System Configuration

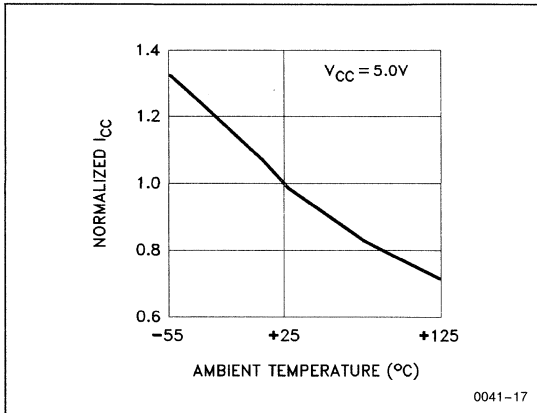


## SYMBOL TABLE

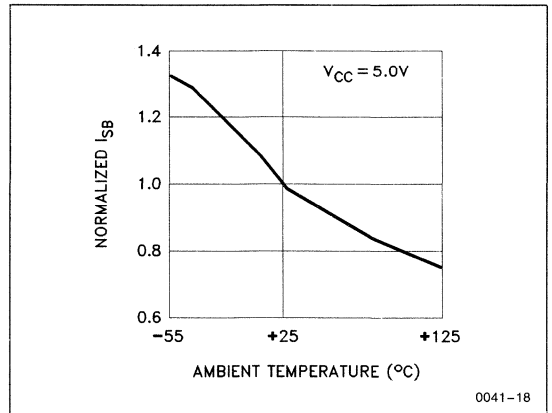
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2404, X2404I

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**





## Electrically Erasable PROM

### TYPICAL FEATURES

- Internally Organized as Two Pages  
—Each 256 x 8
- 2 Wire Serial Interface
- Provides Bidirectional Data Transfer Protocol
- Eight Byte Page Write Mode  
—Minimizes Total Write Time Per Byte
- Self Timed Write Cycle  
—Typical Write Cycle Time of 5 ms
- Data Retention Greater Than 100 Years
- 8 Pin Mini-DIP Package

### DESCRIPTION

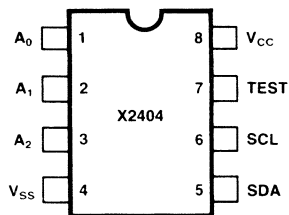
The X2404 is a 4096 bit serial E<sup>2</sup>PROM, internally organized as two 256 x 8 pages. The X2404 is fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories.

The X2404 features a serial interface and software protocol allowing operation on a two wire bus.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to RR504 for further endurance information. Data retention is specified to be greater than 100 years.

2

### PIN CONFIGURATION

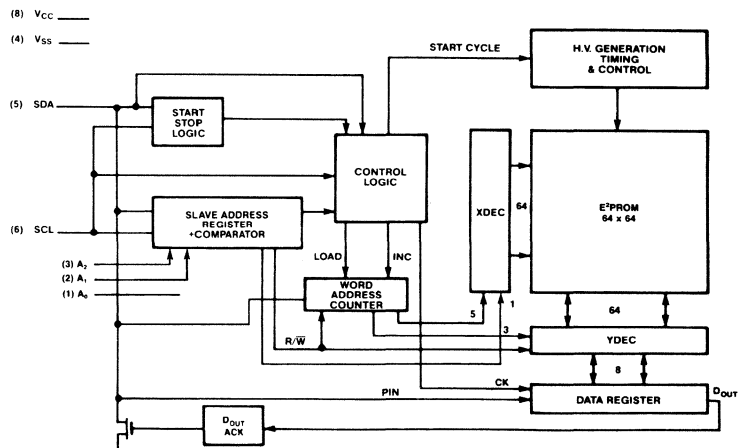


0040-1

### PIN NAMES

1 to 3	A <sub>0</sub> to A <sub>2</sub> Address Inputs
4	V <sub>SS</sub>
5	SDA Serial Data
6	SCL Serial Clock
7	Test Input → to V <sub>SS</sub>
8	V <sub>CC</sub>

### FUNCTIONAL DIAGRAM



0040-2

# X2404M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to $V_{SS}$	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	Power Supply Current		20	35	mA	$f_{SCL} = 100\text{ KHz}$
$I_{SB}$	Standby Current		15	30	mA	
$I_{LI}$	Input Leakage Current		0.1	10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		0.1	10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$I_{TP}^{(2)}$	Test Pin Pull Down Current		16	30	$\mu\text{A}$	$V_{IN} = V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 3\text{ mA}$

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0\text{ MHz}$ , $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(3)}$	Input/Output Capacitance (SDA)	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(3)}$	Input Capacitance ( $A_0, A_1, A_2, SCL$ )	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) Test pin has on chip pull down device which sinks 16  $\mu\text{A}$  (typical) to  $V_{SS}$ .

(3) This parameter is periodically sampled and not 100% tested.

# X2404M

## A.C. CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read & Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$f_{\text{SCL}}$	SCL Clock Frequency	0	100	KHz
$T_I$	Noise Suppression Time Constant at SCL, SDA Inputs		100	ns
$t_{\text{AA}}$	SCL Low to SDA Data Out and ACK Out		3.5	$\mu\text{s}$
$t_{\text{BUF}}$	Time the Bus Must be Free Before a New Transmission Can Start	4.7		$\mu\text{s}$
$t_{\text{HD:STA}}$	Start Condition Hold Time	4.0		$\mu\text{s}$
$t_{\text{LOW}}$	Clock Low Period	4.7		$\mu\text{s}$
$t_{\text{HIGH}}$	Clock High Period	4.0		$\mu\text{s}$
$t_{\text{SU:STA}}$	Start Condition Setup Time (for a Repeated Start Condition)	4.7		$\mu\text{s}$
$t_{\text{HD:DAT}}$	Data In Hold Time	0		$\mu\text{s}$
$t_{\text{SU:DAT}}$	Data In Setup Time	250		ns
$t_{\text{R}}$	SDA and SCL Rise Time		1	$\mu\text{s}$
$t_{\text{F}}$	SDA and SCL Fall Time		300	ns
$t_{\text{SU:STO}}$	Stop Condition Setup Time	4.7		$\mu\text{s}$
$t_{\text{DH}}$	Data Out Hold Time	300		ns

2

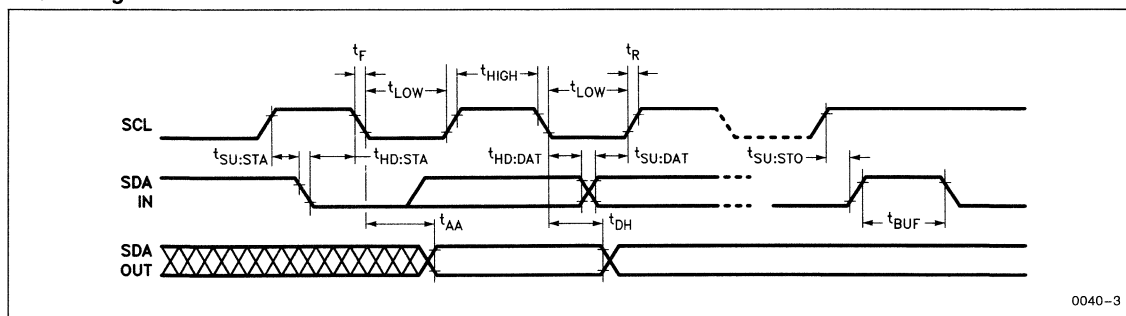
### Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{\text{WR}}$	Write Cycle Time		5	10	ms

The write cycle time is the time from a valid stop condition of a write sequence to the end of the internal erase/program cycle. During the write cycle, the X2404

bus interface circuits are disabled, SDA is allowed to remain high, and the device does not respond to its slave address.

### Bus Timing

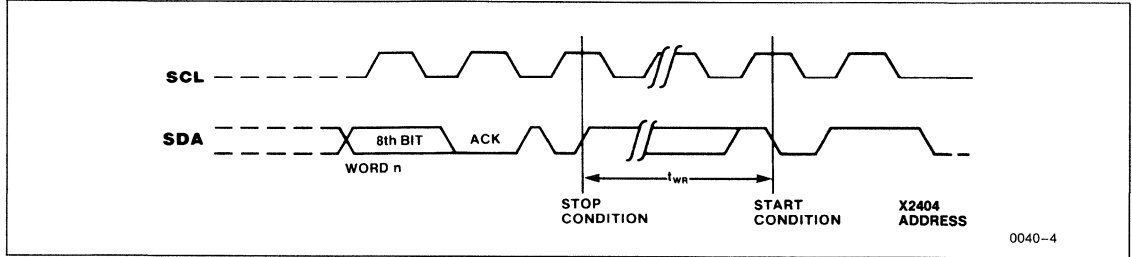


0040-3

Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X2404M

## Write Cycle Timing



## PIN DESCRIPTIONS

### Serial Clock (SCL)

The SCL input is used to clock all data into and out of the device.

### Serial Data (SDA)

SDA is a bidirectional pin used to transfer data into and out of the device. It is an open drain output and may be wire-ORed with any number of open drain or open collector outputs.

### Address ( $A_0$ )

$A_0$  is unused by the X2404, however, it must be tied to  $V_{SS}$  to insure proper device operation.

### Address ( $A_1$ , $A_2$ )

The Address inputs are used to set the least significant two bits of the six bit slave address. The inputs are static, and should be tied HIGH or LOW, forming one unique address per device.

## DEVICE OPERATION

The X2404 supports a bidirectional bus oriented protocol. The protocol defines any device that sends data onto the bus as a transmitter, and the receiving device as the receiver. The device controlling the transfer is a master and the device being controlled is the slave. The master will always initiate data transfers, and provide the clock for both transmit and receive operations. Therefore, the X2404 will be considered a slave in all applications.

### Clock and Data Conventions

Data states on the SDA line can change only during SCL LOW. SDA state changes during SCL HIGH are reserved for indication start and stop conditions. Refer to Figures 1 and 2.

Figure 1: Data Validity

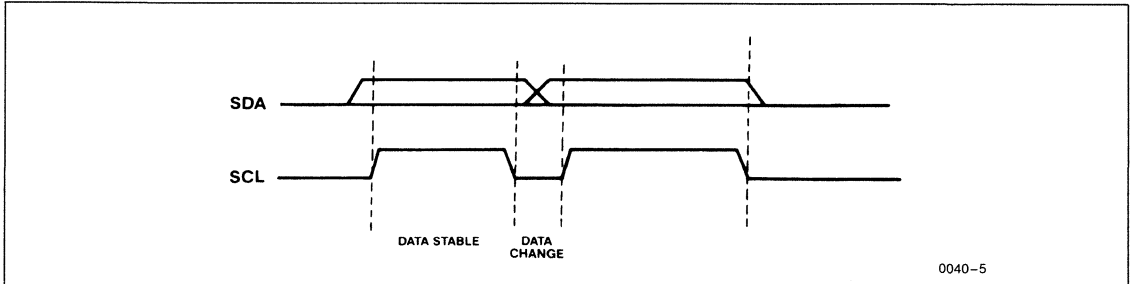
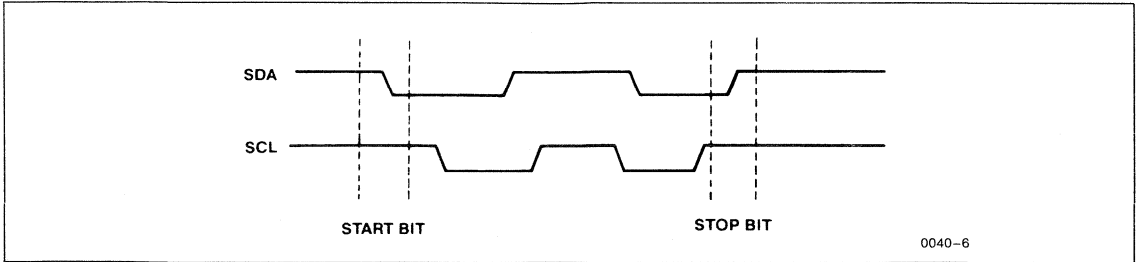


Figure 2: Definition of Start and Stop



2

### Start Condition

All commands are preceded by the start condition, which is a HIGH to LOW transition of SDA when SCL is HIGH. The X2404 continuously monitors the SDA and SCL lines for the start condition and will not respond to any command until this condition has been met.

### Stop Condition

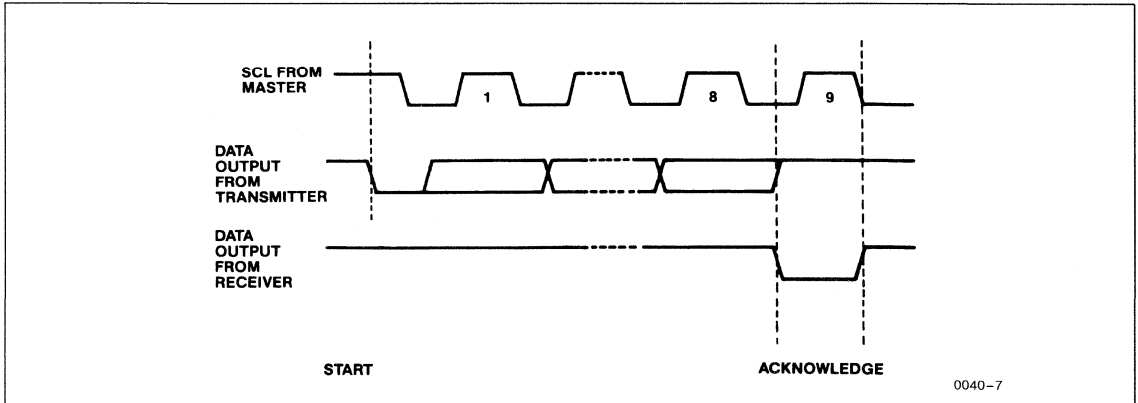
All communications are terminated by a stop condition, which is a LOW to HIGH transition of SDA when SCL is HIGH.

### Acknowledge

Acknowledge is a software convention used to indicate successful data transfers. The transmitting device, either master or slave, will release the bus after transmitting eight bits. During the ninth clock cycle the receiver will pull the SDA line LOW to acknowledge that it received the eight bits of data. Refer to Figure 3.

The X2404 will always respond with an acknowledge after recognition of a start condition and its slave address. If both the device and a write operation have been selected, the X2404 will respond with an acknowledge after the receipt of each subsequent eight bit word.

Figure 3: Acknowledge Response from Receiver



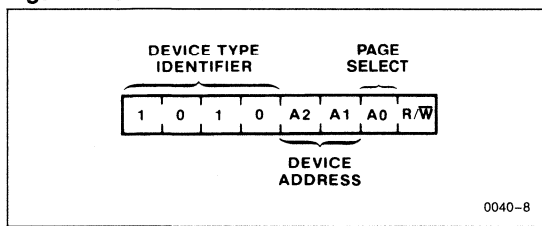
## X2404M

In the read mode the X2404 will transmit eight bits of data, release the SDA line and monitor the line for an acknowledge. If an acknowledge is detected and no stop condition is generated by the master, the X2404 will continue to transmit data. If an acknowledge is not detected, the X2404 will terminate further data transmissions and await the stop condition.

### DEVICE ADDRESSING

Following a start condition the bus master must output the address of the slave it is accessing. The most significant four bits of the slave address are the device type identifier (see Figure 4). For the X2404 this is fixed as 1010[B].

Figure 4: Slave Address



The next two significant bits address a particular device. A system could have up to four X2404 devices on the bus (see Figure 10). The four addresses are defined by the state of the A<sub>1</sub> and A<sub>2</sub> inputs.

The next bit of the slave address field (bit 1) is the page select bit. It is used by the host to toggle between the two 256 word pages of memory.

The last bit of the slave address defines the operation to be performed. When set to one a read operation is selected; when set to zero a write operation is selected.

Following the start condition, the X2404 monitors the SDA bus comparing the slave address being transmitted with its address (device type and state of A<sub>1</sub> and

A<sub>2</sub> inputs). Upon a compare the X2404 outputs an acknowledge on the SDA line. Depending on the state of the R/ $\bar{W}$  bit, the X2404 will execute a read or write operation.

### WRITE OPERATIONS

#### Byte Write

For a write operation, the X2404 requires a second address field. This address field is the word address, comprised of eight bits, providing access to any one of the 256 words of memory. Upon receipt of the word address the X2404 responds with an acknowledge and awaits the next eight bits of data, again responding with an acknowledge. The master then terminates the transfer by generating a stop condition, at which time the X2404 begins the internal write cycle to the nonvolatile memory. While the internal write cycle is in progress the X2404 inputs are disabled, and the device will not respond to any requests from the master. Refer to Figure 5 for the address, acknowledge and data transfer sequence.

#### Page Write

The X2404 is capable of an eight byte page write operation. It is initiated in the same manner as the byte write operation, but instead of terminating the write cycle after the first data word is transferred, the master can transmit up to seven more words. After the receipt of each word, the X2404 will respond with an acknowledge.

After the receipt of each word, the three low order address bits are internally incremented by one. The high order five bits of the address remain constant. If the master should transmit more than eight words prior to generating the stop condition, the address counter will "roll over" and the previously written data will be overwritten. As with the byte write operation, all inputs are disabled until completion of the internal write cycle. Refer to Figure 6 for the address, acknowledge and data transfer sequence.

# X2404M

Figure 5: Byte Write

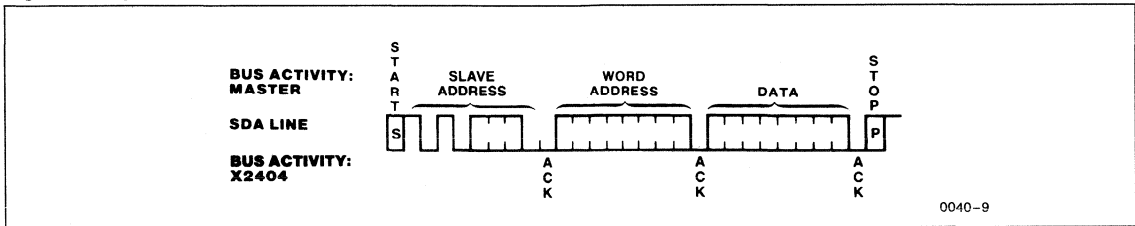
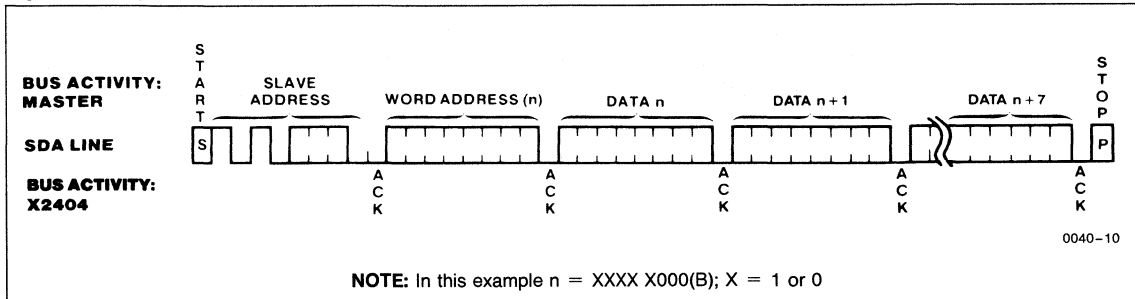


Figure 6: Page Write



## Acknowledge Polling

The disabling of the inputs can be used to take advantage of the typical 5 ms write cycle time. Once the stop condition is issued to indicate the end of the host's write operation the X2404 initiates the internal write cycle. ACK polling can be initiated immediately. This involves issuing the start condition followed by the slave address for a write operation. If the X2404 is still busy with the write operation no ACK will be returned. If the X2404 has completed the write operation an ACK will be returned and the host can then proceed with the next read or write operation.

## READ OPERATIONS

Read operations are initiated in the same manner as write operations with the exception that the R/W bit of

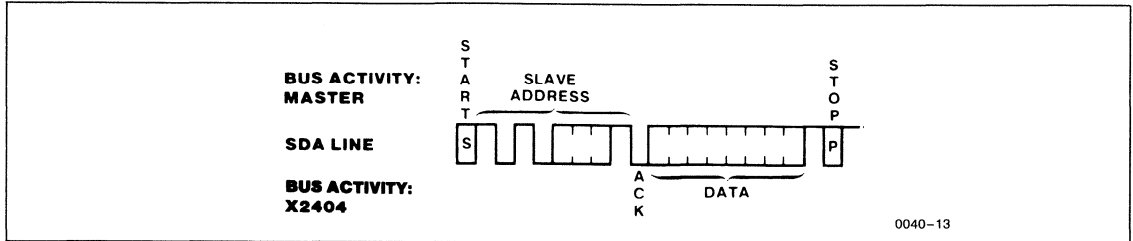
the slave address is set to a one. There are three basic read operations: current address read, random read and sequential read.

## Current Address Read

Internally the X2404 contains an address counter that maintains the address of the last word accessed, incremented by one. Therefore, if the last access (either a read or write) was to address n, the next read operation would access data from address n + 1. Upon receipt of the slave address with R/W set to one, the X2404 issues an acknowledge and transmits the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X2404 discontinues transmission. Refer to Figure 7 for the sequence of address, acknowledge and data transfer.

# X2404M

Figure 7: Current Address Read



## Random Read

Random read operations allow the master to access any memory location in a random manner. Prior to issuing the slave address with the R/W bit set to one, the master must first perform a “dummy” write operation. The master issues the start condition, and the slave address followed by the word address it is to read. After the word address acknowledge, the master immediately reissues the start condition and the slave address with the R/W bit set to one. This will be followed by an acknowledge from the X2404 and then by the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X2404 discontinues transmission. Refer to Figure 8 for the address, acknowledge and data transfer sequence.

## Sequential Read

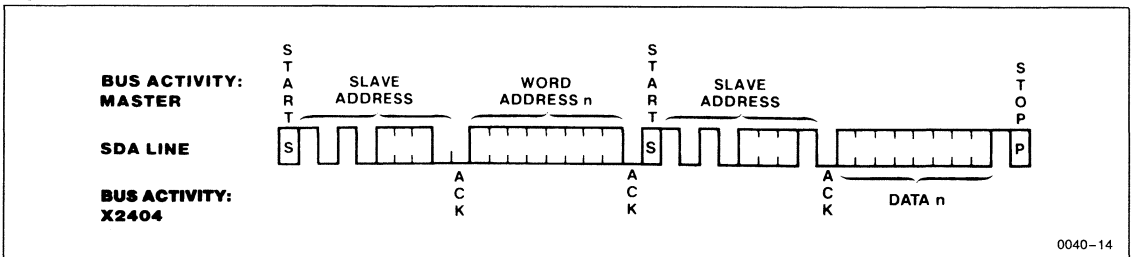
Sequential reads can be initiated as either a current address read or random access read. The first word is transmitted as with the other read modes, however, the master now responds with an acknowledge, indicating it requires additional data. The X2404 continues to output data for each acknowledge received. The read operation is terminated by the master not responding with an acknowledge and generating a stop condition.

The data output is sequential, with the data from address  $n$  followed by the data from  $n + 1$ . The address counter for read operations increments all eight address bits, allowing the entire memory contents of the current 256 word page to be serially read during one operation. If more than 256 words are read, the counter “rolls over” and the X2404 continues to output data from the same 256 word page for each acknowledge received. Refer to Figure 9 for the address, acknowledge and data transfer sequence.

## ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

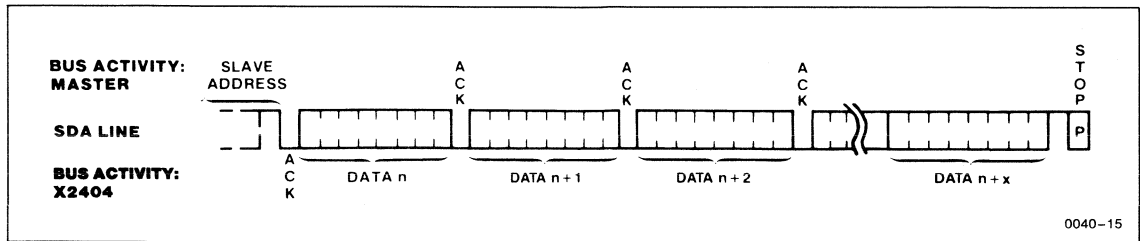
Figure 8: Random Read





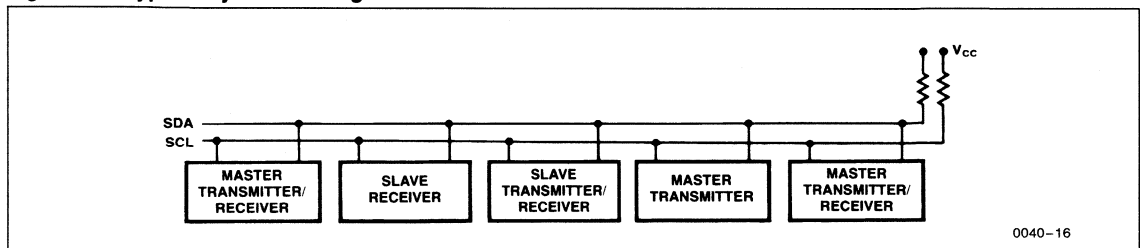
# X2404M

Figure 9: Sequential Read



2

Figure 10: Typical System Configuration

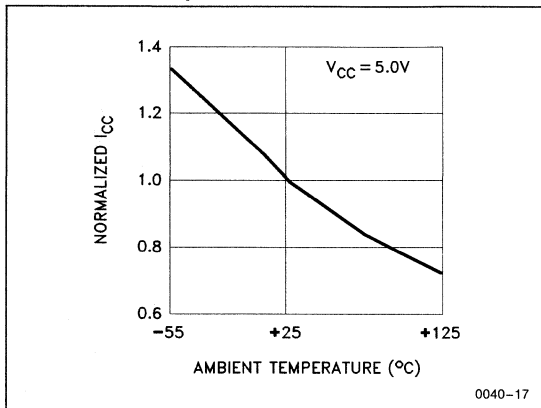


## SYMBOL TABLE

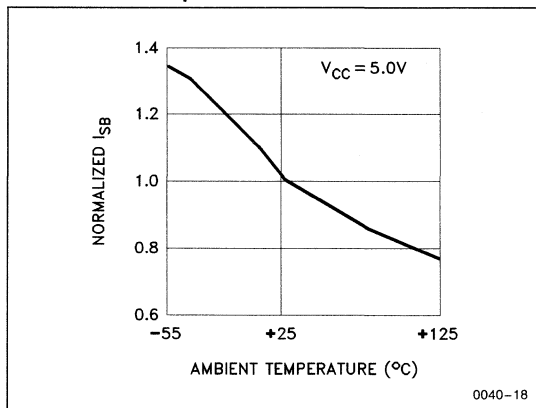
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2404M

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



## Electrically Erasable PROM

### TYPICAL FEATURES

- **Low Power CMOS**
  - 2 mA Active Current Typical
  - 60  $\mu$ A Standby Current Typical
- **Internally Organized as Two Pages**
  - Each 256 x 8
- **2 Wire Serial Interface**
- **Provides Bidirectional Data Transfer Protocol**
- **Sixteen Byte Page Write Mode**
  - Minimizes Total Write Time Per Byte
- **Self Timed Write Cycle**
  - Typical Write Cycle Time of 5 ms
- **Data Retention Greater Than 100 Years**
- **8 Pin Mini-DIP Package**

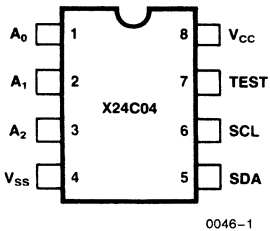
### DESCRIPTION

The X24C04 is a CMOS 4096 bit serial E<sup>2</sup>PROM, internally organized as two 256 x 8 pages. The X24C04 features a serial interface and software protocol allowing operation on a two wire bus.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 100 years.

2

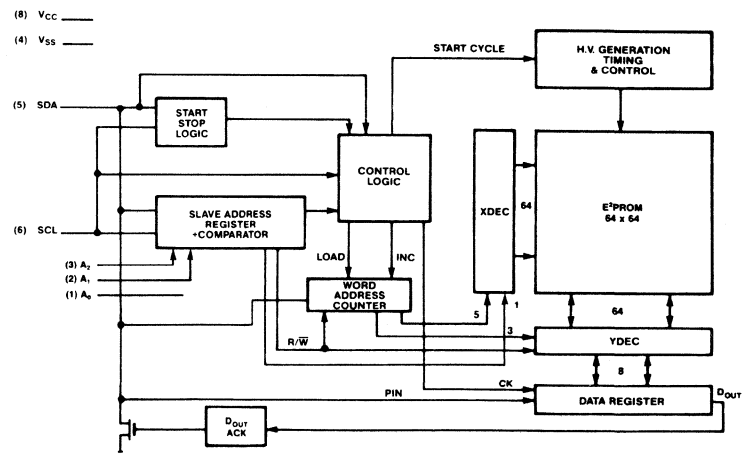
### PIN CONFIGURATION



### PIN NAMES

1 to 3	A <sub>0</sub> to A <sub>2</sub> Address Inputs
4	V <sub>SS</sub>
5	SDA Serial Data
6	SCL Serial Clock
7	Test Input → to V <sub>SS</sub>
8	V <sub>CC</sub>

### FUNCTIONAL DIAGRAM



0046-2

# X24C04, X24C04I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X24C04	-10°C to +85°C
X24C04I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to $V_{SS}$	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X24C04  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X24C04I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	Power Supply Current		2.0		mA	$f_{SCL} = 100\text{ KHz}$
$I_{SB}^{(2)}$	Standby Current		60		$\mu\text{A}$	$V_{IN} = \text{GND or } V_{CC}$
$I_{LI}$	Input Leakage Current		0.1	10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		0.1	10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0		$V_{CC} \times 0.3$	V	
$V_{IH}$	Input High Voltage	$V_{CC} \times 0.7$		$V_{CC} + 0.5$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 3\text{ mA}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0\text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(3)}$	Input/Output Capacitance (SDA)	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(3)}$	Input Capacitance ( $A_0, A_1, A_2, SCL$ )	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	$V_{CC} \times 0.1$ to $V_{CC} \times 0.9$
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	$V_{CC} \times 0.5$
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) SDA and SCL require pull up resistor.

(3) This parameter is periodically sampled and not 100% tested.

## X24C04, X24C04I

### A.C. CHARACTERISTICS LIMITS

X24C04  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

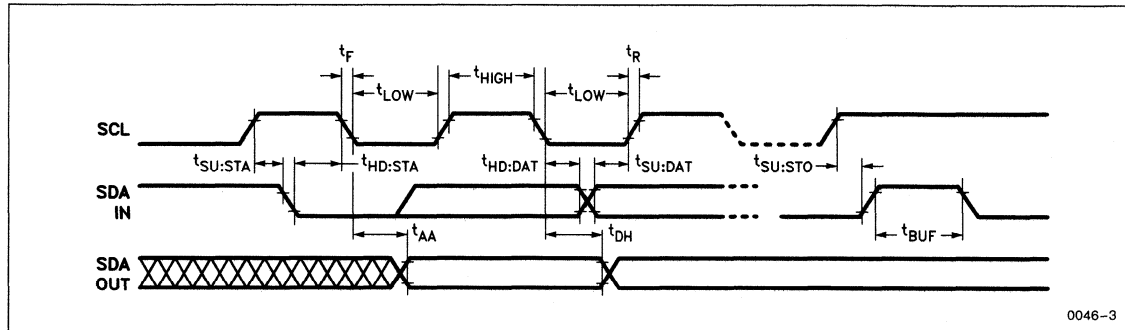
X24C04I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read & Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$f_{\text{SCL}}$	SCL Clock Frequency	0	100	KHz
$T_I$	Noise Suppression Time Constant at SCL, SDA Inputs		100	ns
$t_{\text{AA}}$	SCL Low to SDA Data Out Valid	0.3	3.5	$\mu\text{s}$
$t_{\text{BUF}}$	Time the Bus Must Be Free Before a New Transmission Can Start	4.7		$\mu\text{s}$
$t_{\text{HD:STA}}$	Start Condition Hold Time	4.0		$\mu\text{s}$
$t_{\text{LOW}}$	Clock Low Period	4.7		$\mu\text{s}$
$t_{\text{HIGH}}$	Clock High Period	4.0		$\mu\text{s}$
$t_{\text{SU:STA}}$	Start Condition Setup Time (for a Repeated Start Condition)	4.7		$\mu\text{s}$
$t_{\text{HD:DAT}}$	Data In Hold Time	0		$\mu\text{s}$
$t_{\text{SU:DAT}}$	Data In Setup Time	250		ns
$t_{\text{R}}$	SDA and SCL Rise Time		1	$\mu\text{s}$
$t_{\text{F}}$	SDA and SCL Fall Time		300	ns
$t_{\text{SU:STO}}$	Stop Condition Setup Time	4.7		$\mu\text{s}$
$t_{\text{DH}}$	Data Out Hold Time	300		ns

2

### Bus Timing



0046-3

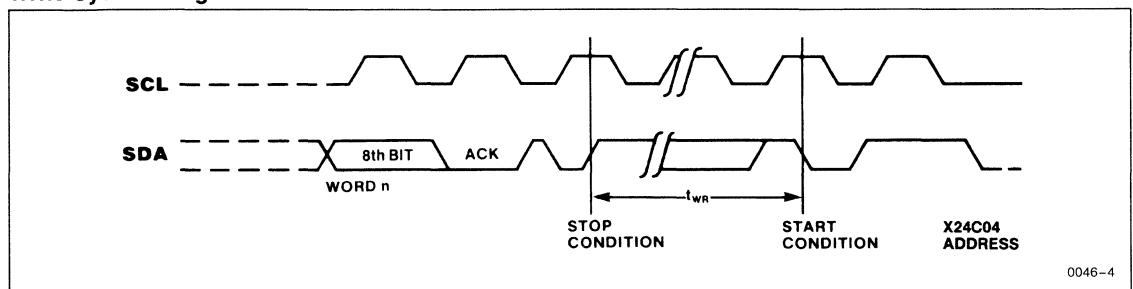
# X24C04, X24C04I

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WR}$	Write Cycle Time		5	10	ms

The write cycle time is the time from a valid stop condition of a write sequence to the end of the internal erase/program cycle. During the write cycle, the X24C04 bus interface circuits are disabled, SDA is allowed to remain high, and the device does not respond to its slave address.

## Write Cycle Timing



## PIN DESCRIPTIONS

### Serial Clock (SCL)

The SCL input is used to clock all data into and out of the device.

### Serial Data (SDA)

SDA is a bidirectional pin used to transfer data into and out of the device. It is an open drain output and may be wire-ORed with any number of open drain or open collector outputs.

### Address ( $A_0$ )

$A_0$  is unused by the X24C04, however, it must be tied to  $V_{SS}$  to insure proper device operation.

### Address ( $A_1, A_2$ )

The Address inputs are used to set the least significant two bits of the six bit slave address. These inputs can be used static or driven. If used statically they must be tied to  $V_{SS}$  or  $V_{CC}$  as appropriate. If driven they must be driven by open collector outputs with resistor pull ups to  $V_{CC}$ .

## DEVICE OPERATION

The X24C04 supports a bidirectional bus oriented protocol. The protocol defines any device that sends data

onto the bus as a transmitter, and the receiving device as the receiver. The device controlling the transfer is a master and the device being controlled is the slave. The master will always initiate data transfers, and provide the clock for both transmit and receive operations. Therefore, the X24C04 will be considered a slave in all applications.

### Clock and Data Conventions

Data states on the SDA line can change only during SCL LOW. SDA state changes during SCL HIGH are reserved for indicating start and stop conditions. Refer to Figures 1 and 2.

### Start Condition

All commands are preceded by the start condition, which is a HIGH to LOW transition of SDA when SCL is HIGH. The X24C04 continuously monitors the SDA and SCL lines for the start condition and will not respond to any command until this condition has been met.

**Note:** (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage (5V).

# X24C04, X24C04I

Figure 1: Data Validity

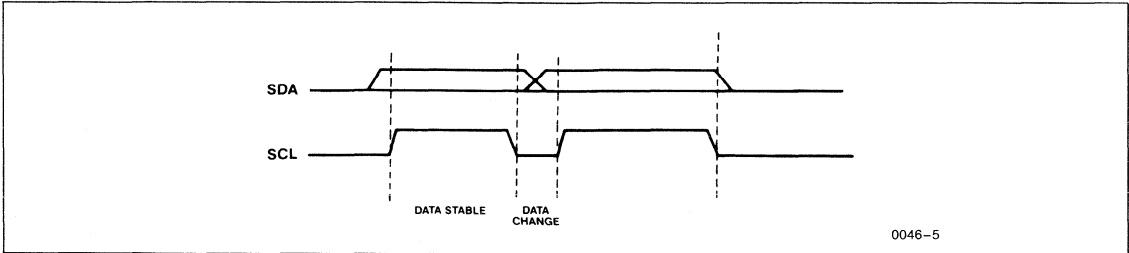
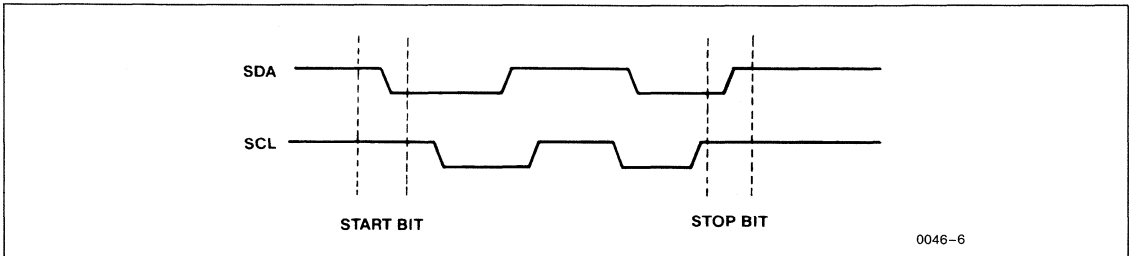


Figure 2: Definition of Start and Stop



## Stop Condition

All communications are terminated by a stop condition, which is a LOW to HIGH transition of SDA when SCL is HIGH. The stop condition is also used by the X24C04 to place the device in the standby power mode.

## Acknowledge

Acknowledge is a software convention used to indicate successful data transfers. The transmitting device, either master or slave, will release the bus after transmitting eight bits. During the ninth clock cycle the receiver will pull the SDA line LOW to acknowledge that it received the eight bits of data. Refer to Figure 3.

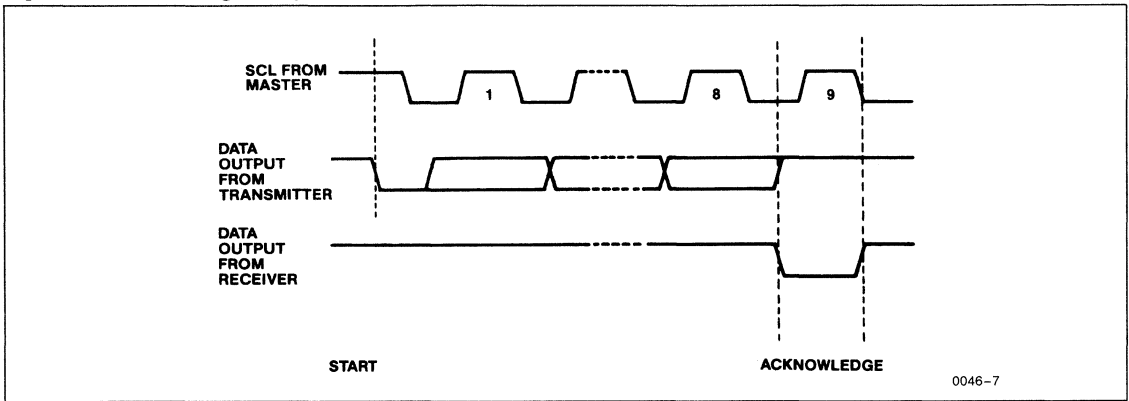
The X24C04 will always respond with an acknowledge after recognition of a start condition and its slave

address. If both the device and a write operation have been selected, the X24C04 will respond with an acknowledge after the receipt of each subsequent eight bit word.

In the read mode the X24C04 will transmit eight bits of data, release the SDA line and monitor the line for an acknowledge. If an acknowledge is detected and no stop condition is generated by the master, the X24C04 will continue to transmit data. If an acknowledge is not detected, the X24C04 will terminate further data transmissions and await the stop condition to return to the standby power mode.

# X24C04, X24C04I

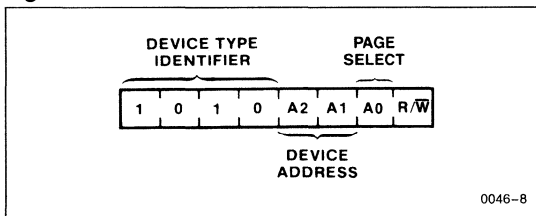
**Figure 3: Acknowledge Response From Receiver**



## DEVICE ADDRESSING

Following a start condition the bus master must output the address of the slave it is accessing. The most significant four bits of the slave address are the device type identifier (see Figure 4). For the X24C04 this is fixed as 1010[B].

**Figure 4: Slave Address**



The next two significant bits address a particular device. A system could have up to four X24C04 devices on the bus (see Figure 10). The four addresses are defined by the state of the  $A_1$  and  $A_2$  inputs.

The next bit of the slave address field (bit 1) is the page select bit. It is used by the host to toggle between the two 256 word pages of memory. This is, in effect the most significant bit for the word address.

The last bit of the slave address defines the operation to be performed. When set to one a read operation

is selected, when set to zero a write operation is selected.

Following the start condition, the X24C04 monitors the SDA bus comparing the slave address being transmitted with its address (device type and state of  $A_1$  and  $A_2$  inputs). Upon a compare the X24C04 outputs an acknowledge on the SDA line. Depending on the state of the R/ $\bar{W}$  bit, the X24C04 will execute a read or write operation.

## WRITE OPERATIONS

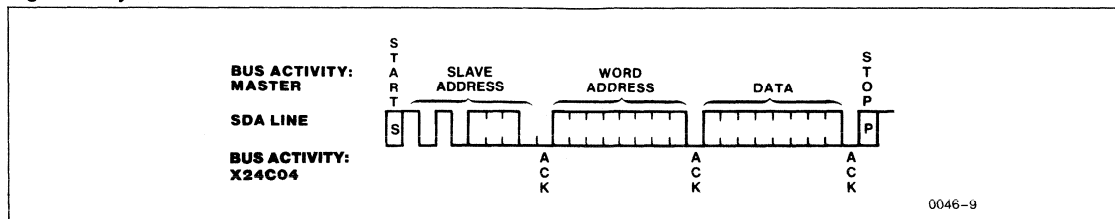
### Byte Write

For a write operation, the X24C04 requires a second address field. This address field is the word address, comprised of eight bits, providing access to any one of the 256 words of memory. Upon receipt of the word address the X24C04 responds with an acknowledge, and awaits the next eight bits of data, again responding with an acknowledge. The master then terminates the transfer by generating a stop condition, at which time the X24C04 begins the internal write cycle to the non-volatile memory. While the internal write cycle is in progress the X24C04 inputs are disabled, and the device will not respond to any requests from the master. Refer to Figure 5 for the address, acknowledge and data transfer sequence.



## X24C04, X24C04I

Figure 5: Byte Write



### Page Write

The X24C04 is capable of a sixteen byte page write operation. It is initiated in the same manner as the byte write operation, but instead of terminating the write cycle after the first data word is transferred, the master can transmit up to fifteen more words. After the receipt of each word, the X24C04 will respond with an acknowledge.

After the receipt of each word, the four low order address bits are internally incremented by one. The high order five bits of the address remain constant. If the master should transmit more than sixteen words prior to generating the stop condition, the address counter will “roll over” and the previously written data will be overwritten. As with the byte write operation, all inputs are disabled until completion of the internal write cycle. Refer to Figure 6 for the address, acknowledge and data transfer sequence.

### Acknowledge Polling

The disabling of the inputs can be used to take advantage of the typical 5 ms write cycle time. Once the stop condition is issued to indicate the end of the host’s write operation the X24C04 initiates the internal write cycle. ACK polling can be initiated immediately. This involves issuing the start condition followed by the slave

address for a write operation. If the X24C04 is still busy with the write operation no ACK will be returned. If the X24C04 has completed the write operation an ACK will be returned and the host can then proceed with the next read or write operation.

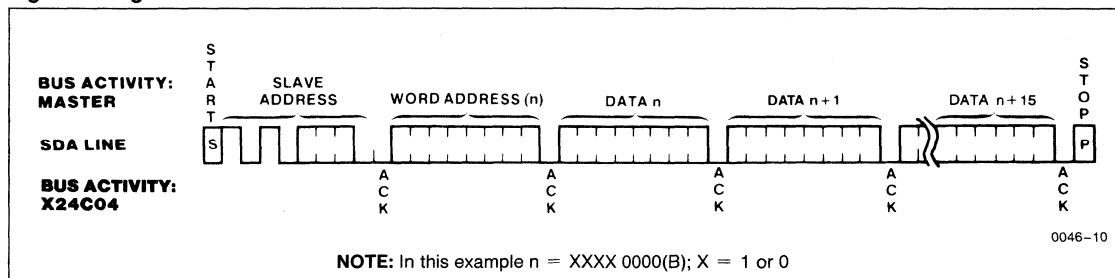
### READ OPERATIONS

Read operations are initiated in the same manner as write operations with the exception that the bit of the slave address is set to a one. There are three basic read operations: current address read, random read and sequential read.

#### Current Address Read

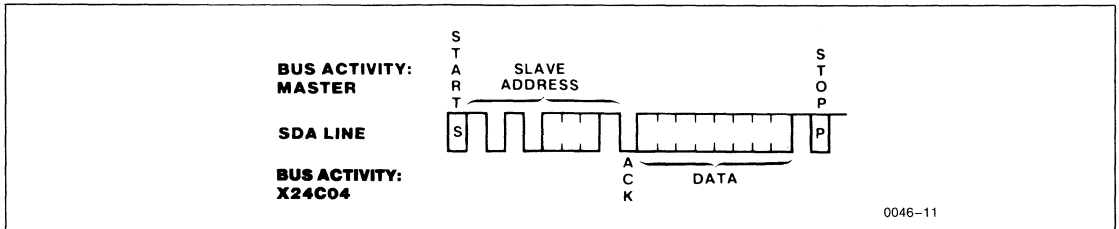
Internally the X24C04 contains an address counter that maintains the address of the last word accessed, incremented by one. Therefore, if the last access (either a read or write) was to address  $n$ , the next read operation would access data from address  $n + 1$ . Upon receipt of the slave address with  $R/\bar{W}$  set to one, the X24C04 issues an acknowledge and transmits the eight bit word. The master does not acknowledge the transfer but does generate a stop condition and the X24C04 discontinues transmission. Refer to Figure 7 for the sequence of address, acknowledge and data transfer.

Figure 6: Page Write



# X24C04, X24C04I

Figure 7: Current Address Read



## Random Read

Random read operations allow the master to access any memory location in a random manner. Prior to issuing the slave address with the R/W bit set to one, the master must first perform a "dummy" write operation. The master issues the start condition, and the slave address followed by the word address it is to read. After the word address acknowledge, the master immediately reissues the start condition and the slave address with the R/W bit set to one. This will be followed by an acknowledge from the X24C04 and then by the eight bit word. The master does not acknowledge the transfer but does generate the stop condition and the X24C04 discontinues transmission. Refer to Figure 8 for the address, acknowledge and data transfer sequence.

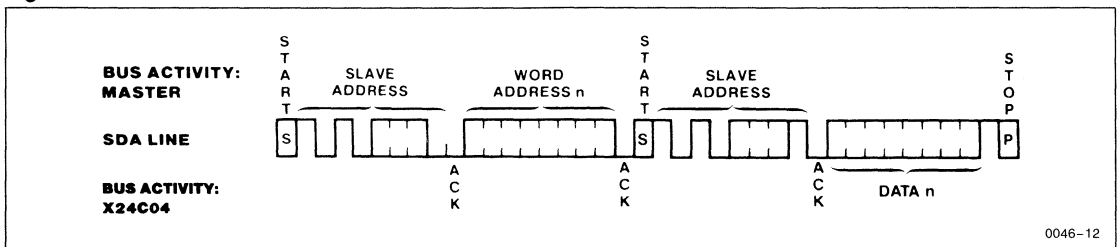
transmitted as with the other read modes, however, the master now responds with an acknowledge, indicating it requires additional data. The X24C04 continues to output data for each acknowledge received. The read operation is terminated by the master not responding with an acknowledge and generating a stop condition.

The data output is sequential, with the data from address  $n$  followed by the data from  $n + 1$ . The address counter for read operations increments all address bits, allowing the entire memory contents to be serially read during one operation. If more than 512 words are read, the counter "rolls over" and the X24C04 continues to output data for each acknowledge received. Refer to Figure 9 for the address, acknowledge and data transfer sequence.

## Sequential Read

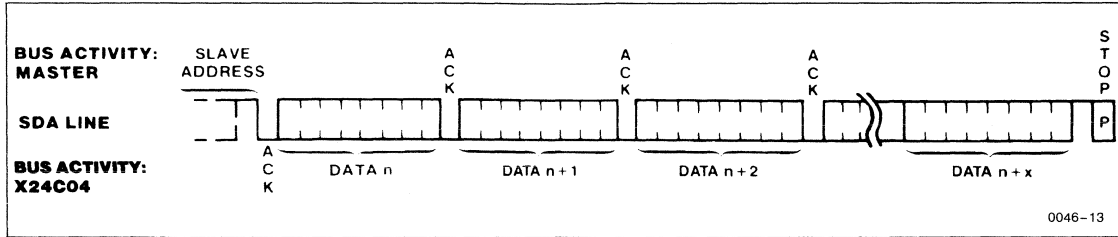
Sequential reads can be initiated as either a current address read or random access read. The first word is

Figure 8: Random Read



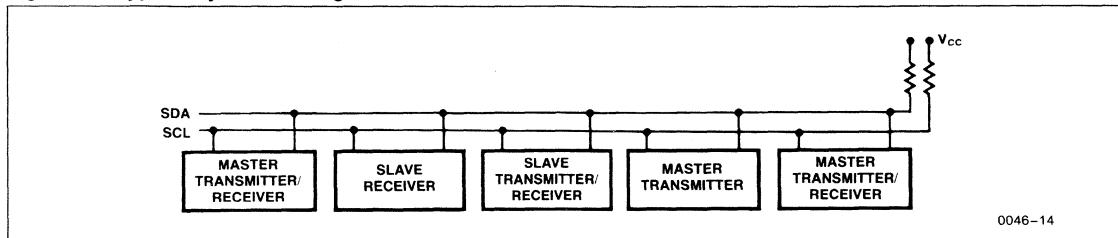
# X24C04, X24C04I

Figure 9: Sequential Read



2

Figure 10: Typical System Configuration



## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

---

## NOTES

## Electrically Erasable PROM

### TYPICAL FEATURES

- **Low Power CMOS**
  - 2 mA Active Current Typical
  - 60  $\mu$ A Standby Current Typical
- **Internally Organized as Eight Pages**
  - Each 256 x 8
- **2 Wire Serial Interface**
- **Provides Bidirectional Data Transfer Protocol**
- **Sixteen Byte Page Write Mode**
  - Minimizes Total Write Time Per Byte
- **Self Timed Write Cycle**
  - Typical Write Cycle Time of 5 ms
- **Data Retention Greater Than 100 Years**
- **8 Pin Mini-DIP Package**

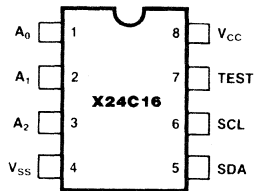
### DESCRIPTION

The X24C16 is a CMOS 16,384 bit serial E<sup>2</sup>PROM, internally organized as eight 256 x 8 pages. The X24C16 features a serial interface and software protocol allowing operation on a two wire bus.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 100 years.



### PIN CONFIGURATION

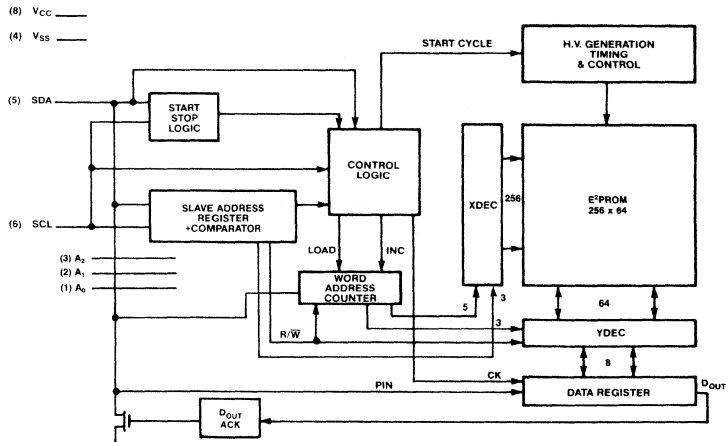


0038-1

### PIN NAMES

1 to 3	A <sub>0</sub> to A <sub>2</sub> Address Inputs
4	V <sub>SS</sub>
5	SDA Serial Data
6	SCL Serial Clock
7	Test Input → to V <sub>SS</sub>
8	V <sub>CC</sub>

### FUNCTIONAL DIAGRAM



0038-2

# X24C16, X24C16I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X24C16	-10°C to +85°C
X24C16I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to $V_{SS}$	-1.0V to +7V
D.C. Output Current	.5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X24C16  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X24C16I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	Power Supply Current		2.0	3.0	mA	$f_{SCL} = 100\text{ KHz}$
$I_{SB}^{(2)}$	Standby Current		60	100	$\mu\text{A}$	$V_{IN} = \text{GND or } V_{CC}$
$I_{LI}$	Input Leakage Current		0.1	10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		0.1	10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0		$V_{CC} \times 0.3$	V	
$V_{IH}$	Input High Voltage	$V_{CC} \times 0.7$		$V_{CC} + 0.5$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 3\text{ mA}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0\text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(3)}$	Input/Output Capacitance (SDA)	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(3)}$	Input Capacitance ( $A_0, A_1, A_2, SCL$ )	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	$V_{CC} \times 0.1$ to $V_{CC} \times 0.9$
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	$V_{CC} \times 0.5$
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) SDA and SCL require pull up resistor.

(3) This parameter is periodically sampled and not 100% tested.

# X24C16, X24C16I

## A.C. CHARACTERISTICS LIMITS

X24C16  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

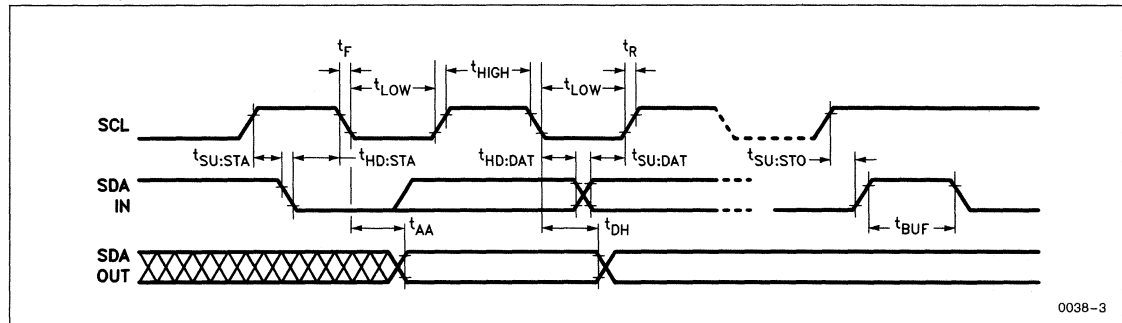
X24C16I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read & Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$f_{\text{SCL}}$	SCL Clock Frequency	0	100	KHz
$T_I$	Noise Suppression Time Constant at SCL, SDA Inputs		100	ns
$t_{\text{AA}}$	SCL Low to SDA Data Out Valid	0.3	3.5	$\mu\text{s}$
$t_{\text{BUF}}$	Time the Bus Must Be Free Before a New Transmission Can Start	4.7		$\mu\text{s}$
$t_{\text{HD:STA}}$	Start Condition Hold Time	4.0		$\mu\text{s}$
$t_{\text{LOW}}$	Clock Low Period	4.7		$\mu\text{s}$
$t_{\text{HIGH}}$	Clock High Period	4.0		$\mu\text{s}$
$t_{\text{SU:STA}}$	Start Condition Setup Time (for a Repeated Start Condition)	4.7		$\mu\text{s}$
$t_{\text{HD:DAT}}$	Data In Hold Time	0		$\mu\text{s}$
$t_{\text{SU:DAT}}$	Data In Setup Time	250		ns
$t_{\text{R}}$	SDA and SCL Rise Time		1	$\mu\text{s}$
$t_{\text{F}}$	SDA and SCL Fall Time		300	ns
$t_{\text{SU:STO}}$	Stop Condition Setup Time	4.7		$\mu\text{s}$
$t_{\text{DH}}$	Data Out Hold Time	300		ns

2

### Bus Timing



0038-3

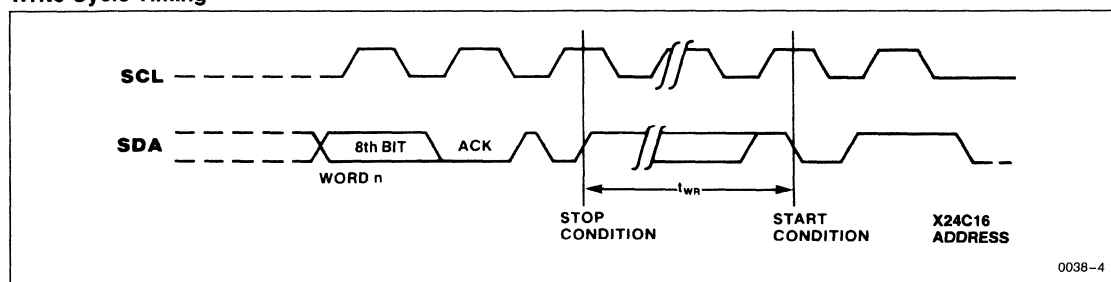
## X24C16, X24C16I

### Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WR}$	Write Cycle Time		5	10	ms

The write cycle time is the time from a valid stop condition of a write sequence to the end of the internal erase/program cycle. During the write cycle, the X24C16 bus interface circuits are disabled, SDA is allowed to remain high, and the device does not respond to its slave address.

### Write Cycle Timing



### PIN DESCRIPTIONS

#### Serial Clock (SCL)

The SCL input is used to clock all data into and out of the device.

#### Serial Data (SDA)

SDA is a bidirectional pin used to transfer data into and out of the device. It is an open drain output and may be wire-ORed with any number of open drain or open collector outputs.

#### Address (A<sub>0</sub>, A<sub>1</sub>, A<sub>2</sub>)

The A<sub>0</sub>, A<sub>1</sub> and A<sub>2</sub> inputs are unused by the X24C16, however, they must be tied to V<sub>SS</sub> to insure proper device operation.

### DEVICE OPERATION

The X24C16 supports a bidirectional bus oriented protocol. The protocol defines any device that sends data onto the bus as a transmitter, and the receiving device

as the receiver. The device controlling the transfer is a master and the device being controlled is the slave. The master will always initiate data transfers, and provide the clock for both transmit and receive operations. Therefore, the X24C16 will be considered a slave in all applications.

#### Clock and Data Conventions

Data states on the SDA line can change only during SCL LOW. SDA state changes during SCL HIGH are reserved for indicating start and stop conditions. Refer to Figures 1 and 2.

#### Start Condition

All commands are preceded by the start condition, which is a HIGH to LOW transition of SDA when SCL is HIGH. The X24C16 continuously monitors the SDA and SCL lines for the start condition and will not respond to any command until this condition has been met.

**Note:** (4) Typical values are for T<sub>A</sub> = 25°C and nominal supply voltage (5V).



## X24C16, X24C16I

Figure 1: Data Validity

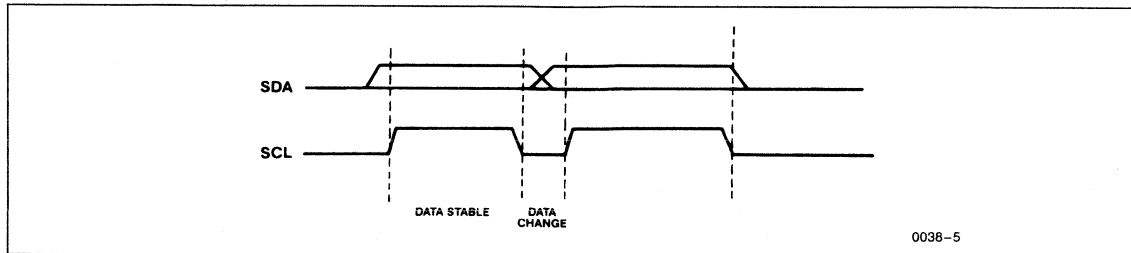
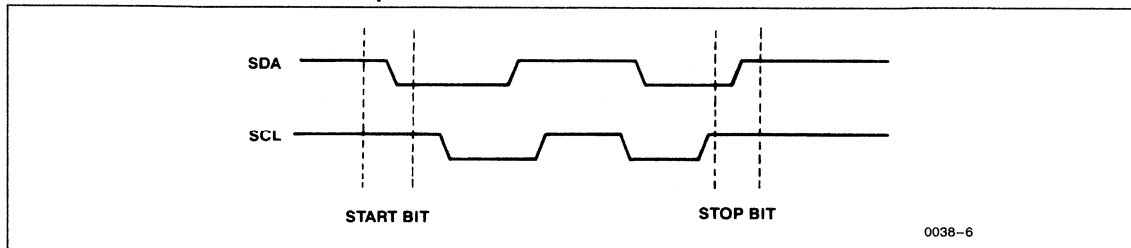


Figure 2: Definition of Start and Stop



### Stop Condition

All communications are terminated by a stop condition, which is a LOW to HIGH transition of SDA when SCL is HIGH. The stop condition is also used by the X24C16 to place the device in the standby power mode.

### Acknowledge

Acknowledge is a software convention used to indicate successful data transfers. The transmitting device, either master or slave, will release the bus after transmitting eight bits. During the ninth clock cycle the receiver will pull the SDA line LOW to acknowledge that it received the eight bits of data. Refer to Figure 3.

The X24C16 will always respond with an acknowledge after recognition of a start condition and its slave

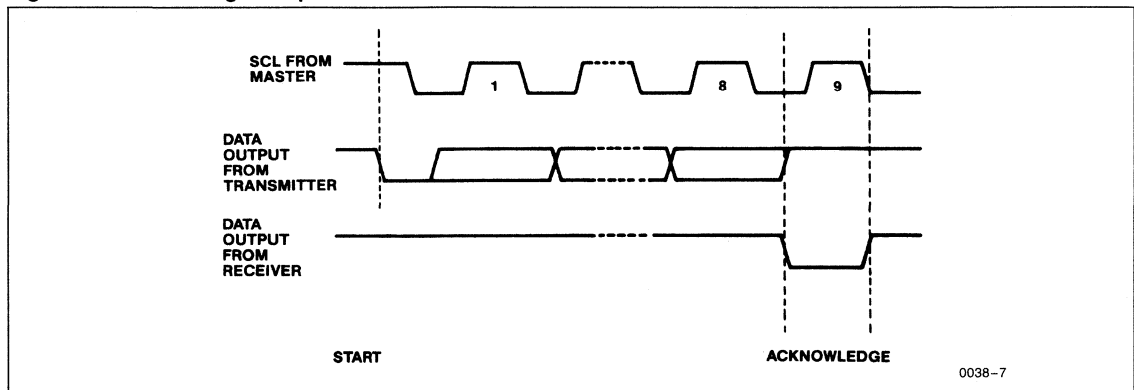
address. If both the device and a write operation have been selected, the X24C16 will respond with an acknowledge after the receipt of each subsequent eight bit word.

In the read mode the X24C16 will transmit eight bits of data, release the SDA line and monitor the line for an acknowledge. If an acknowledge is detected and no stop condition is generated by the master, the X24C16 will continue to transmit data. If an acknowledge is not detected, the X24C16 will terminate further data transmissions and await the stop condition to return to the standby power mode.

2

# X24C16, X24C16I

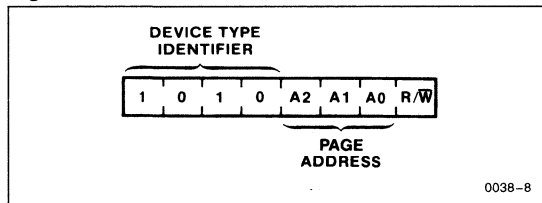
Figure 3: Acknowledge Response From Receiver



## DEVICE ADDRESSING

Following a start condition the bus master must output the address of the slave it is accessing. The most significant four bits of the slave address are the device type identifier (see Figure 4). For the X24C16 this is fixed as 1010[B].

Figure 4: Slave Address



The next three bits of the slave address field are the page select bits. They are used by the master device to select which of the eight 256 word pages of memory are to be accessed. These bits are, in effect, the three most significant bits of the word address. It should be noted, the protocol limits the size of memory to eight pages of 256 words; therefore, the protocol can support only one X24C16 per system.

The last bit of the slave address defines the operation to be performed. When set to one a read operation is

selected, when set to zero a write operation is selected.

Following the start condition, the X24C16 monitors the SDA bus comparing the slave address being transmitted with its slave address. Upon a compare the X24C16 outputs an acknowledge on the SDA line. Depending on the state of the R/W bit, the X24C16 will execute a read or write operation.

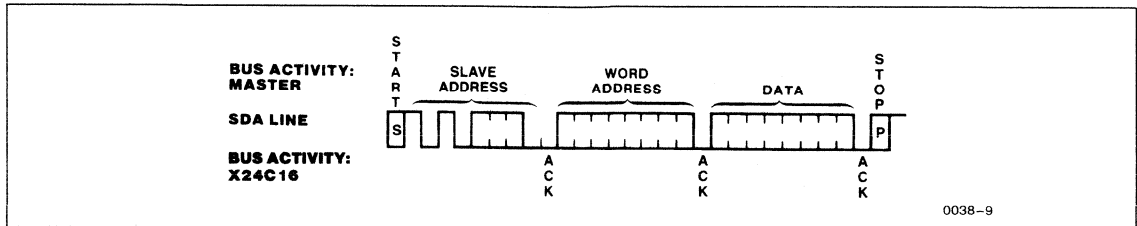
## WRITE OPERATIONS

### Byte Write

For a write operation, the X24C16 requires a second address field. This address field is the word address, comprised of eight bits, providing access to any one of the 256 words in the selected page of memory. Upon receipt of the word address the X24C16 responds with an acknowledge, and awaits the next eight bits of data, again responding with an acknowledge. The master then terminates the transfer by generating a stop condition, at which time the X24C16 begins the internal write cycle to the nonvolatile memory. While the internal write cycle is in progress the X24C16 inputs are disabled, and the device will not respond to any requests from the master. Refer to Figure 5 for the address, acknowledge and data transfer sequence.

# X24C16, X24C16I

Figure 5: Byte Write



## Page Write

The X24C16 is capable of a sixteen byte page write operation. It is initiated in the same manner as the byte write operation, but instead of terminating the write cycle after the first data word is transferred, the master can transmit up to fifteen more words. After the receipt of each word, the X24C16 will respond with an acknowledge.

After the receipt of each word, the four low order address bits are internally incremented by one. The high order seven bits of the word address remain constant. If the master should transmit more than sixteen words prior to generating the stop condition, the address counter will “roll over” and the previously written data will be overwritten. As with the byte write operation, all inputs are disabled until completion of the internal write cycle. Refer to Figure 6 for the address, acknowledge and data transfer sequence.

## Acknowledge Polling

The disabling of the inputs can be used to take advantage of the typical 5 ms write cycle time. Once the stop condition is issued to indicate the end of the host’s write operation the X24C16 initiates the internal write cycle. ACK polling can be initiated immediately. This involves issuing the start condition followed by the slave

address for a write operation. If the X24C16 is still busy with the write operation no ACK will be returned. If the X24C16 has completed the write operation an ACK will be returned and the host can then proceed with the next read or write operation.

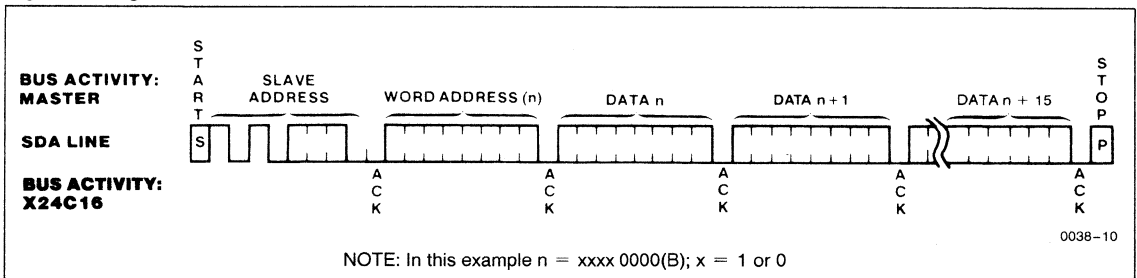
## READ OPERATIONS

Read operations are initiated in the same manner as write operations with the exception that the R/W bit of the slave address is set to a one. There are three basic read operations: current address read, random read and sequential read.

### Current Address Read

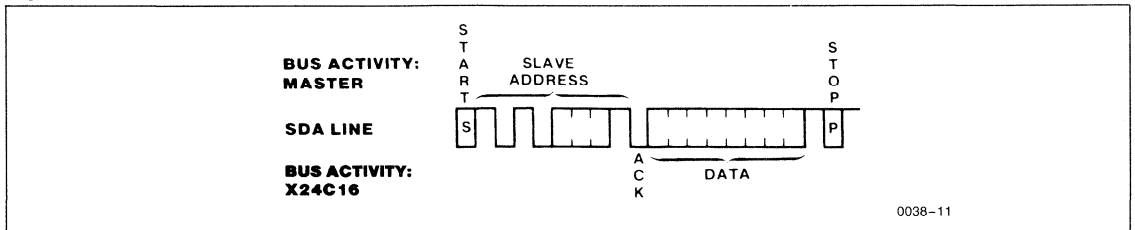
Internally the X24C16 contains an address counter that maintains the address of the last word accessed, incremented by one. Therefore, if the last access (either a read or write) was to address n, the next read operation would access data from address n + 1. Upon receipt of the slave address with R/W set to one, the X24C16 issues an acknowledge and transmits the eight bit word. The master will not acknowledge the transfer but does generate a stop condition and the X24C16 discontinues transmission. Refer to Figure 7 for the sequence of address, acknowledge and data transfer.

Figure 6: Page Write



# X24C16, X24C16I

Figure 7: Current Address Read



## Random Read

Random read operations allow the master to access any memory location in a random manner. Prior to issuing the slave address with the  $R/\bar{W}$  bit set to one, the master must first perform a “dummy” write operation. The master issues the start condition, and the slave address followed by the word address it is to read. After the word address acknowledge, the master immediately reissues the start condition and the slave address with the  $R/\bar{W}$  bit set to one. This will be followed by an acknowledge from the X24C16 and then by the eight bit word. The master will not acknowledge the transfer but does generate the stop condition and the X24C16 discontinues transmission. Refer to Figure 8 for the address, acknowledge and data transfer sequence.

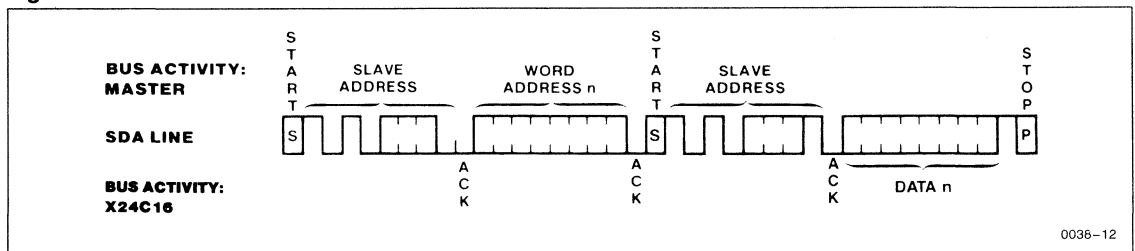
transmitted as with the other read modes, however, the master now responds with an acknowledge, indicating it requires additional data. The X24C16 continues to output data for each acknowledge received. The read operation is terminated by the master not responding with an acknowledge and generating a stop condition.

The data output is sequential, with the data from address  $n$  followed by the data from  $n+1$ . The address counter for read operations increments all word address bits, allowing the entire memory contents to be serially read during one operation. If more than 2048 words are read, the counter “rolls over” and the X24C16 continues to output data for each acknowledge received. Refer to Figure 9 for the address, acknowledge and data transfer sequence.

## Sequential Read

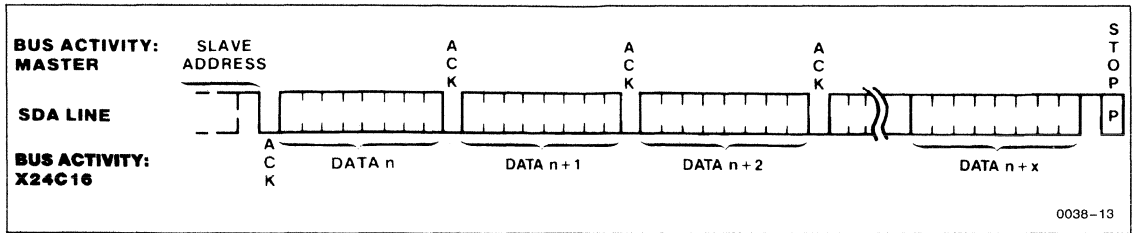
Sequential reads can be initiated as either a current address read or random access read. The first word is

Figure 8: Random Read



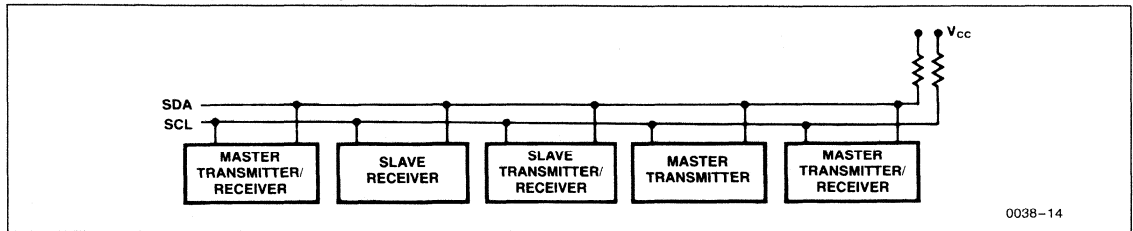
# X24C16, X24C16I

Figure 9: Sequential Read



2

Figure 10: Typical System Configuration



## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

---

## NOTES

**Electrically Erasable PROM**

**TYPICAL FEATURES**

- **Low Power CMOS**
  - 2 mA Active Current Typical
  - 60  $\mu$ A Standby Current Typical
- **Internally Organized as Eight Pages**
  - Each 256 x 8
- **2 Wire Serial Interface**
- **Provides Bidirectional Data Transfer Protocol**
- **Sixteen Byte Page Write Mode**
  - Minimizes Total Write Time Per Byte
- **Self Timed Write Cycle**
  - Typical Write Cycle Time of 5 ms
- **Data Retention Greater Than 100 Years**
- **8 Pin Mini-DIP Package**

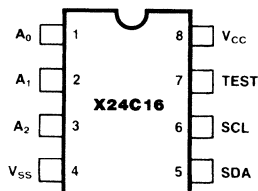
**DESCRIPTION**

The X24C16 is a CMOS 16,384 bit serial E<sup>2</sup>PROM, internally organized as eight 256 x 8 pages. The X24C16 features a serial interface and software protocol allowing operation on a two wire bus.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 100 years.



**PIN CONFIGURATION**

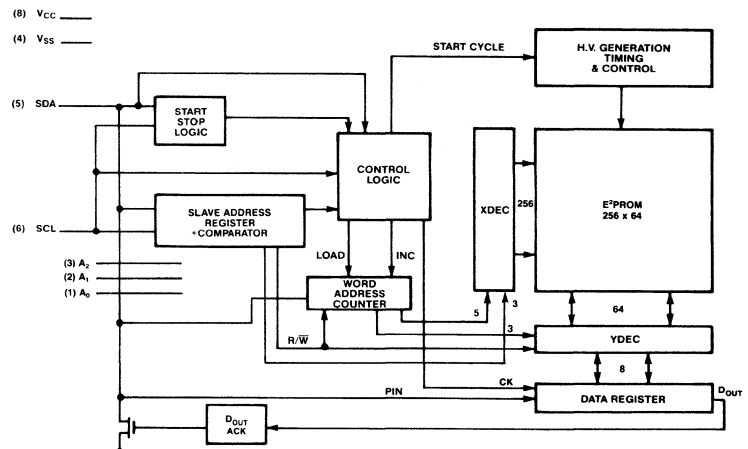


0047-1

**PIN NAMES**

1 to 3	A <sub>0</sub> to A <sub>2</sub> Address Inputs
4	V <sub>SS</sub>
5	SDA Serial Data
6	SCL Serial Clock
7	Test Input → to V <sub>SS</sub>
8	V <sub>CC</sub>

**FUNCTIONAL DIAGRAM**



0047-2

# X24C16M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to $V_{SS}$	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	Power Supply Current		2.0	3.0	mA	$f_{SCL} = 100\text{ KHz}$
$I_{SB}^{(2)}$	Standby Current		60	100	$\mu\text{A}$	$V_{IN} = \text{GND or } V_{CC}$
$I_{LI}$	Input Leakage Current		0.1	10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		0.1	10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0		$V_{CC} \times 0.3$	V	
$V_{IH}$	Input High Voltage	$V_{CC} \times 0.7$		$V_{CC} + 0.5$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 3\text{ mA}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0\text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(3)}$	Input/Output Capacitance (SDA)	8	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(3)}$	Input Capacitance ( $A_0, A_1, A_2, \text{SCL}$ )	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	$V_{CC} \times 0.1$ to $V_{CC} \times 0.9$
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	$V_{CC} \times 0.5$
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) SDA and SCL require pull up resistor.

(3) This parameter is periodically sampled and not 100% tested.



# X24C16M

## A.C. CHARACTERISTICS LIMITS

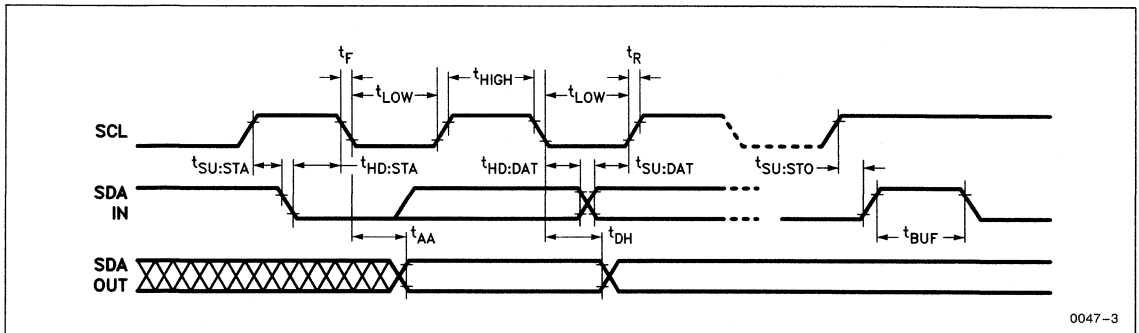
$T_A = -55^{\circ}\text{C}$  to  $+125^{\circ}\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read & Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$f_{\text{SCL}}$	SCL Clock Frequency	0	100	KHz
$T_I$	Noise Suppression Time Constant at SCL, SDA Inputs		100	ns
$t_{\text{AA}}$	SCL Low to SDA Data Out Valid	0.3	3.5	$\mu\text{s}$
$t_{\text{BUF}}$	Time the Bus Must Be Free Before a New Transmission Can Start	4.7		$\mu\text{s}$
$t_{\text{HD:STA}}$	Start Condition Hold Time	4.0		$\mu\text{s}$
$t_{\text{LOW}}$	Clock Low Period	4.7		$\mu\text{s}$
$t_{\text{HIGH}}$	Clock High Period	4.0		$\mu\text{s}$
$t_{\text{SU:STA}}$	Start Condition Setup Time (for a Repeated Start Condition)	4.7		$\mu\text{s}$
$t_{\text{HD:DAT}}$	Data In Hold Time	0		$\mu\text{s}$
$t_{\text{SU:DAT}}$	Data In Setup Time	250		ns
$t_{\text{R}}$	SDA and SCL Rise Time		1	$\mu\text{s}$
$t_{\text{F}}$	SDA and SCL Fall Time		300	ns
$t_{\text{SU:STO}}$	Stop Condition Setup Time	4.7		$\mu\text{s}$
$t_{\text{DH}}$	Data Out Hold Time	300		ns

2

### Bus Timing



0047-3

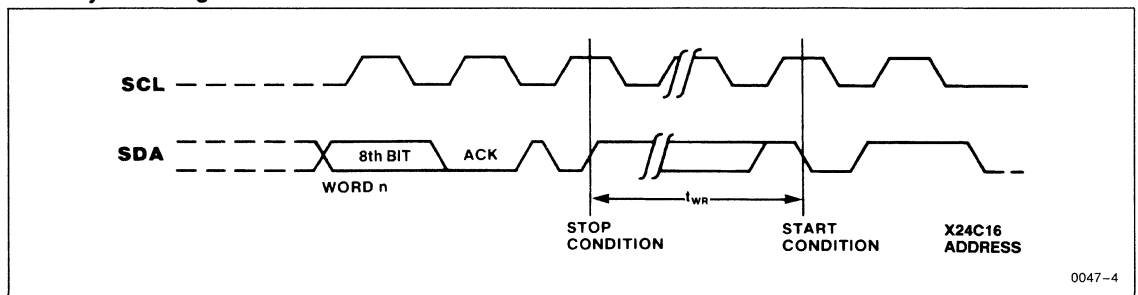
# X24C16M

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WR}$	Write Cycle Time		5	10	ms

The write cycle time is the time from a valid stop condition of a write sequence to the end of the internal erase/program cycle. During the write cycle, the X24C16 bus interface circuits are disabled, SDA is allowed to remain high, and the device does not respond to its slave address.

## Write Cycle Timing



## PIN DESCRIPTIONS

### Serial Clock (SCL)

The SCL input is used to clock all data into and out of the device.

### Serial Data (SDA)

SDA is a bidirectional pin used to transfer data into and out of the device. It is an open drain output and may be wire-ORed with any number of open drain or open collector outputs.

### Address (A<sub>0</sub>, A<sub>1</sub>, A<sub>2</sub>)

The A<sub>0</sub>, A<sub>1</sub> and A<sub>2</sub> inputs are unused by the X24C16, however, they must be tied to V<sub>SS</sub> to insure proper device operation.

## DEVICE OPERATION

The X24C16 supports a bidirectional bus oriented protocol. The protocol defines any device that sends data onto the bus as a transmitter, and the receiving device

as the receiver. The device controlling the transfer is a master and the device being controlled is the slave. The master will always initiate data transfers, and provide the clock for both transmit and receive operations. Therefore, the X24C16 will be considered a slave in all applications.

### Clock and Data Conventions

Data states on the SDA line can change only during SCL LOW. SDA state changes during SCL HIGH are reserved for indicating start and stop conditions. Refer to Figures 1 and 2.

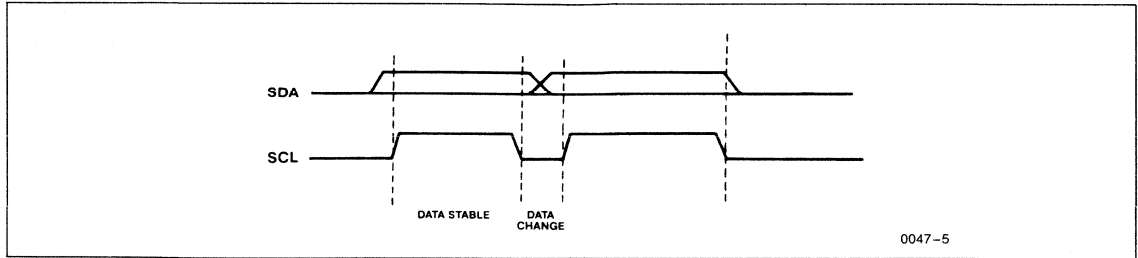
### Start Condition

All commands are preceded by the start condition, which is a HIGH to LOW transition of SDA when SCL is HIGH. The X24C16 continuously monitors the SDA and SCL lines for the start condition and will not respond to any command until this condition has been met.

**Note:** (4) Typical values are for T<sub>A</sub> = 25°C and nominal supply voltage (5V).

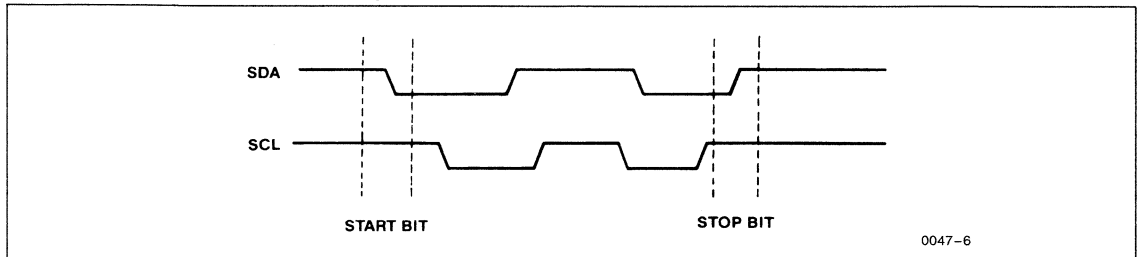
# X24C16M

Figure 1: Data Validity



2

Figure 2: Definition of Start and Stop



## Stop Condition

All communications are terminated by a stop condition, which is a LOW to HIGH transition of SDA when SCL is HIGH. The stop condition is also used by the X24C16 to place the device in the standby power mode.

## Acknowledge

Acknowledge is a software convention used to indicate successful data transfers. The transmitting device, either master or slave, will release the bus after transmitting eight bits. During the ninth clock cycle the receiver will pull the SDA line LOW to acknowledge that it received the eight bits of data. Refer to Figure 3.

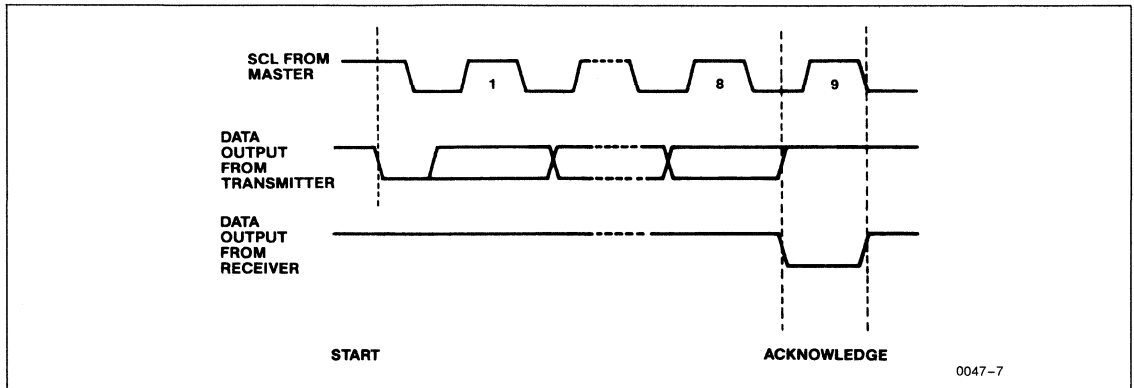
The X24C16 will always respond with an acknowledge after recognition of a start condition and its slave

address. If both the device and a write operation have been selected, the X24C16 will respond with an acknowledge after the receipt of each subsequent eight bit word.

In the read mode the X24C16 will transmit eight bits of data, release the SDA line and monitor the line for an acknowledge. If an acknowledge is detected and no stop condition is generated by the master, the X24C16 will continue to transmit data. If an acknowledge is not detected, the X24C16 will terminate further data transmissions and await the stop condition to return to the standby power mode.

# X24C16M

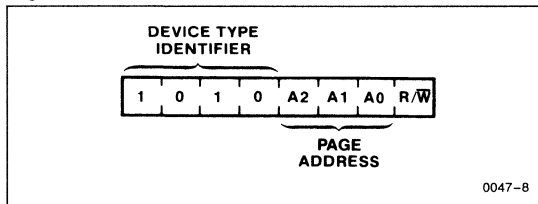
Figure 3: Acknowledge Response From Receiver



## DEVICE ADDRESSING

Following a start condition the bus master must output the address of the slave it is accessing. The most significant four bits of the slave address are the device type identifier (see Figure 4). For the X24C16 this is fixed as 1010[B].

Figure 4: Slave Address



The next three bits of the slave address field are the page select bits. They are used by the master device to select which of the eight 256 word pages of memory are to be accessed. These bits are, in effect, the three most significant bits of the word address. It should be noted, the protocol limits the size of memory to eight pages of 256 words; therefore, the protocol can support only one X24C16 per system.

The last bit of the slave address defines the operation to be performed. When set to one a read operation

is selected, when set to zero a write operation is selected.

Following the start condition, the X24C16 monitors the SDA bus comparing the slave address being transmitted with its slave address. Upon a compare the X24C16 outputs an acknowledge on the SDA line. Depending on the state of the R/W bit, the X24C16 will execute a read or write operation.

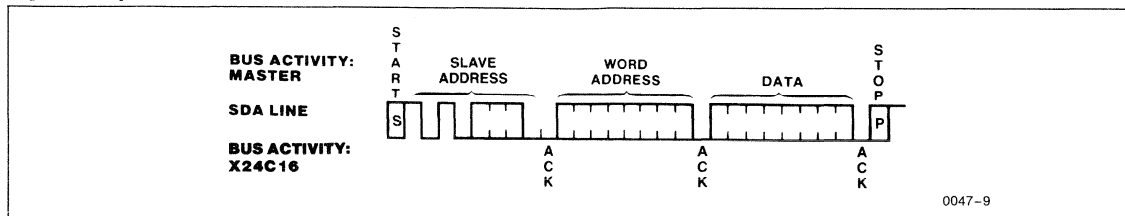
## WRITE OPERATIONS

### Byte Write

For a write operation, the X24C16 requires a second address field. This address field is the word address, comprised of eight bits, providing access to any one of the 256 words in the selected page of memory. Upon receipt of the word address the X24C16 responds with an acknowledge, and awaits the next eight bits of data, again responding with an acknowledge. The master then terminates the transfer by generating a stop condition, at which time the X24C16 begins the internal write cycle to the nonvolatile memory. While the internal write cycle is in progress the X24C16 inputs are disabled, and the device will not respond to any requests from the master. Refer to Figure 5 for the address, acknowledge and data transfer sequence.

# X24C16M

Figure 5: Byte Write



2

## Page Write

The X24C16 is capable of a sixteen byte page write operation. It is initiated in the same manner as the byte write operation, but instead of terminating the write cycle after the first data word is transferred, the master can transmit up to fifteen more words. After the receipt of each word, the X24C16 will respond with an acknowledge.

After the receipt of each word, the four low order address bits are internally incremented by one. The high order seven bits of the word address remain constant. If the master should transmit more than sixteen words prior to generating the stop condition, the address counter will “roll over” and the previously written data will be overwritten. As with the byte write operation, all inputs are disabled until completion of the internal write cycle. Refer to Figure 6 for the address, acknowledge and data transfer sequence.

## Acknowledge Polling

The disabling of the inputs can be used to take advantage of the typical 5 ms write cycle time. Once the stop condition is issued to indicate the end of the host’s write operation the X24C16 initiates the internal write cycle. ACK polling can be initiated immediately. This involves issuing the start condition followed by the

slave address for a write operation. If the X24C16 is still busy with the write operation no ACK will be returned. If the X24C16 has completed the write operation an ACK will be returned and the host can then proceed with the next read or write operation.

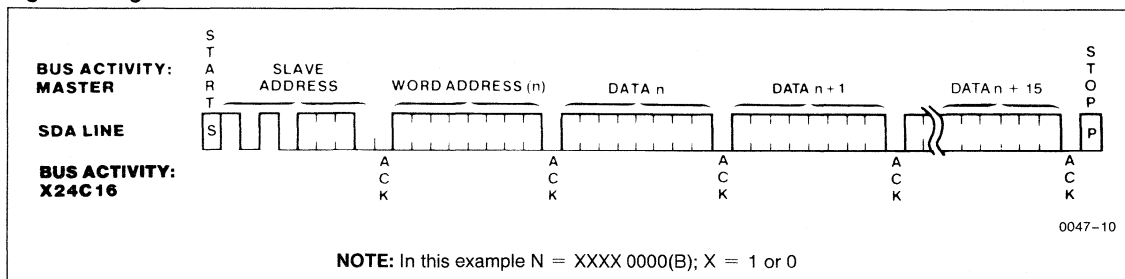
## READ OPERATIONS

Read operations are initiated in the same manner as write operations with the exception that the  $R/\overline{W}$  bit of the slave address is set to a one. There are three basic read operations: current address read, random read and sequential read.

## Current Address Read

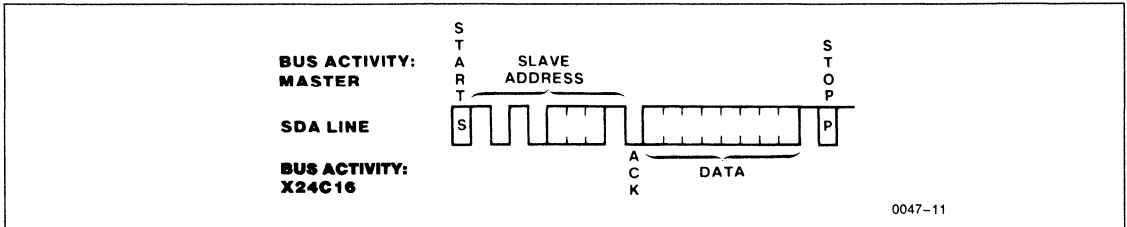
Internally the X24C16 contains an address counter that maintains the address of the last word accessed, incremented by one. Therefore, if the last access (either a read or write) was to address  $n$ , the next read operation would access data from address  $n + 1$ . Upon receipt of the slave address with  $R/\overline{W}$  set to one, the X24C16 issues an acknowledge and transmits the eight bit word. The master will not acknowledge the transfer but does generate a stop condition and the X24C16 discontinues transmission. Refer to Figure 7 for the sequence of address, acknowledge and data transfer.

Figure 6: Page Write



# X24C16M

**Figure 7: Current Address Read**



## Random Read

Random read operations allow the master to access any memory location in a random manner. Prior to issuing the slave address with the R/W bit set to one, the master must first perform a “dummy” write operation. The master issues the start condition, and the slave address followed by the word address it is to read. After the word address acknowledge, the master immediately reissues the start condition and the slave address with the R/W bit set to one. This will be followed by an acknowledge from the X24C16 and then by the eight bit word. The master will not acknowledge the transfer but does generate the stop condition and the X24C16 discontinues transmission. Refer to Figure 8 for the address, acknowledge and data transfer sequence.

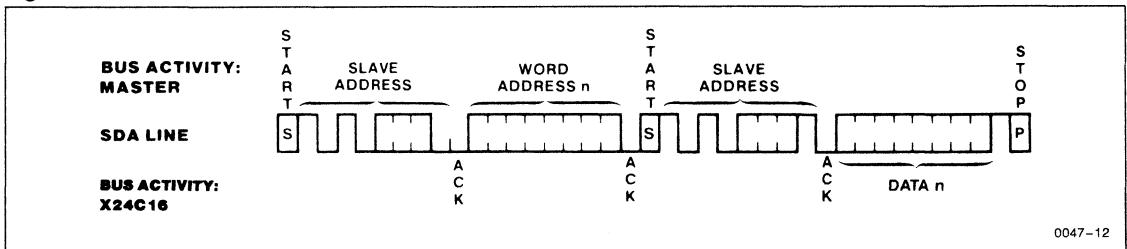
## Sequential Read

Sequential reads can be initiated as either a current address read or random access read. The first word is

transmitted as with the other read modes, however, the master now responds with an acknowledge, indicating it requires additional data. The X24C16 continues to output data for each acknowledge received. The read operation is terminated by the master not responding with an acknowledge and generating a stop condition.

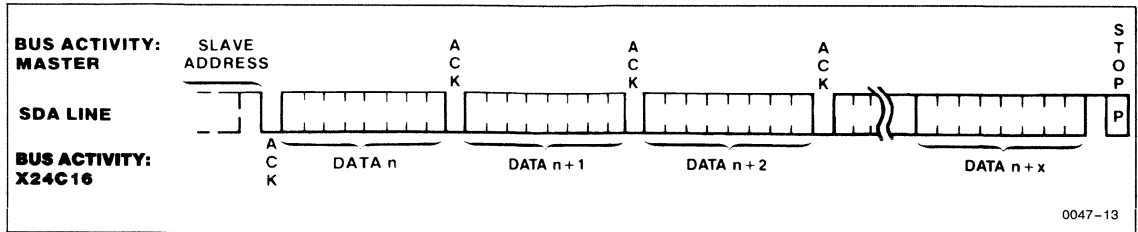
The data output is sequential, with the data from address  $n$  followed by the data from  $n + 1$ . The address counter for read operations increments all word address bits, allowing the entire memory contents to be serially read during one operation. If more than 2048 words are read, the counter “rolls over” and the X24C16 continues to output data for each acknowledge received. Refer to Figure 9 for the address, acknowledge and data transfer sequence.

**Figure 8: Random Read**



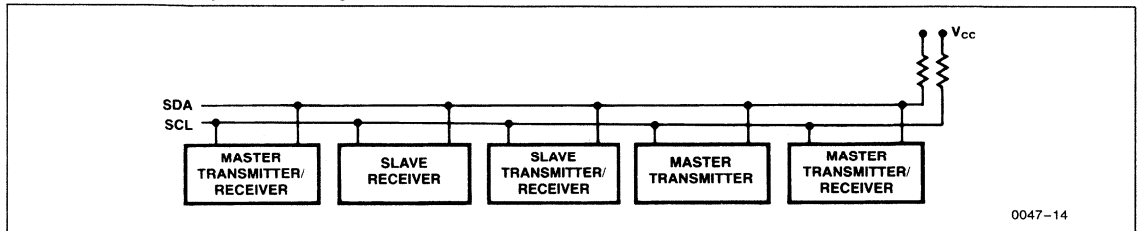
# X24C16M

Figure 9: Sequential Read



2

Figure 10: Typical System Configuration



## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

---

## NOTES



X2804A, X2804AI .....	3-1
X2804AM .....	3-9
X2816A, X2816AI .....	3-19
X2816AM .....	3-27
X2816B, X2816BI .....	3-35
X2816BM .....	3-45
X2864A, X2864AI .....	3-57
X2864AM .....	3-67
X2864AT .....	3-79
X2864B, X2864BI .....	3-89
X2864BM .....	3-97
X2864H, X2864HI .....	3-105
X2864HM .....	3-113
X28256, X28256I .....	3-121
X28256M .....	3-135
X28C256, X28C256I .....	3-149
X28C256M .....	3-163
X28C010 .....	3-177



**NOVRAM\* Data Sheets** **1**

**Serial I/O Data Sheets** **2**

**E<sup>2</sup>PROM Data Sheets** **3**



4K

Commercial  
Industrial

X2804A  
X2804AI

512 x 8 Bit

## Electrically Erasable PROM

### FEATURES

- Simple Byte Write Operation
  - No High Voltages Necessary
  - Single TTL Level  $\overline{WE}$  Signal Modifies Data
  - Internally Latched Address and Data
  - Self Timed Write
  - Noise Protected  $\overline{WE}$  Pin
- Reliable N-Channel Floating Gate MOS Technology
- Single 5V Supply
- Byte Write Time: 10 ms Max.
- Fast Access Time: 250 ns Max.
- Low Power Dissipation
  - Active Current: 80 mA Max.
  - Standby Current: 50 mA Max.

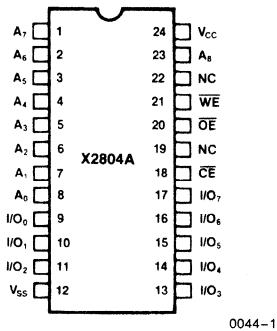
### DESCRIPTION

The Xicor X2804A is a 512 x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2804A is compatible with the JEDEC approved pinout for byte-wide memories.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.

3

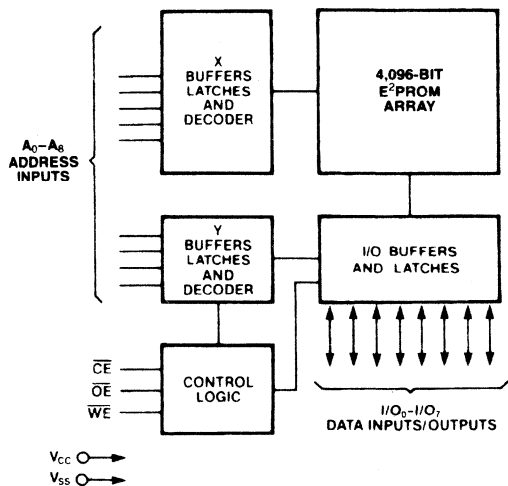
### PIN CONFIGURATION



### PIN NAMES

A <sub>0</sub> -A <sub>8</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
OE	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2804A, X2804AI

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2804A	-10°C to +85°C
X2804AI	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2804A  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2804AI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2804A Limits		X2804AI Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80		100	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		50		60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 0.5$	2.2	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -400 \mu\text{A}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2804A, X2804AI

## A.C. CHARACTERISTICS

X2804A  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

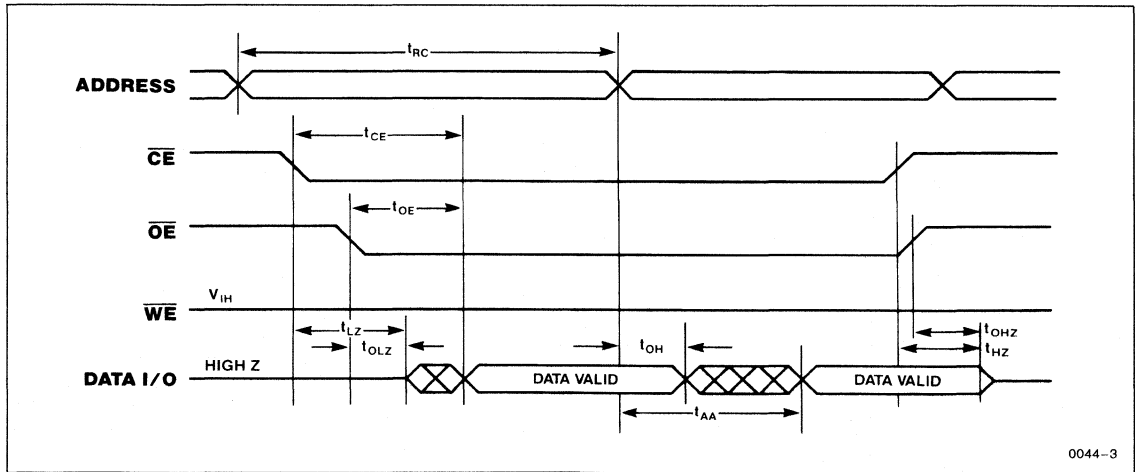
X2804AI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2804A-25 X2804AI-25		X2804A X2804AI		X2804A-35 X2804AI-35		X2804A-45 X2804AI-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		450		ns
$t_{CE}$	Chip Enable Access Time		250		300		350		450	ns
$t_{AA}$	Address Access Time		250		300		350		450	ns
$t_{OE}$	Output Enable Access Time		120		120		135		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	100	10	100	10	100	ns
$t_{OLZ}$	Output Enable to Output in Low Z	50		50		50		50		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	100	10	100	10	100	ns
$t_{OH}$	Output Hold from Address Change	20		20		20		20		ns

3

### Read Cycle



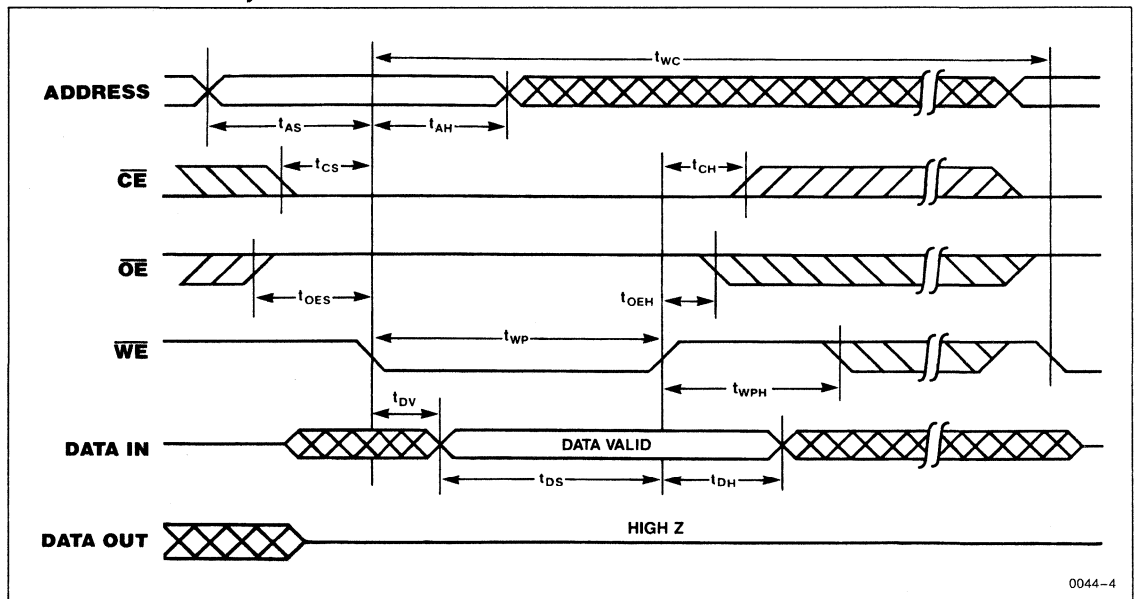
**Note:** (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2804A, X2804AI

## Write Cycle Limits

Symbol	Parameter	X2804A-25 X2804AI-25		X2804A X2804AI		X2804A-35 X2804AI-35		X2804A-45 X2804AI-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	10		10		10		10		ms
$t_{AS}$	Address Setup Time	10		10		10		10		ns
$t_{AH}$	Address Hold Time	120		120		150		150		ns
$t_{CS}$	Write Setup Time	0		0		0		0		ns
$t_{CH}$	Write Hold Time	0		0		0		0		ns
$t_{CW}$	Chip Enable to End of Write Input	150		150		175		230		ns
$t_{OES}$	Output Enable Setup Time	10		10		10		10		ns
$t_{OEH}$	Output Enable Hold Time	10		10		10		10		ns
$t_{WP}$	Write Pulse Width	150		150		175		230		ns
$t_{WPH}$	Write Control Recovery	50		50		50		50		ns
$t_{DV}$	Data Valid Time		1		1		1		1	$\mu$ s
$t_{DS}$	Data Setup Time	120		135		175		230		ns
$t_{DH}$	Data Hold Time	15		15		20		30		ns

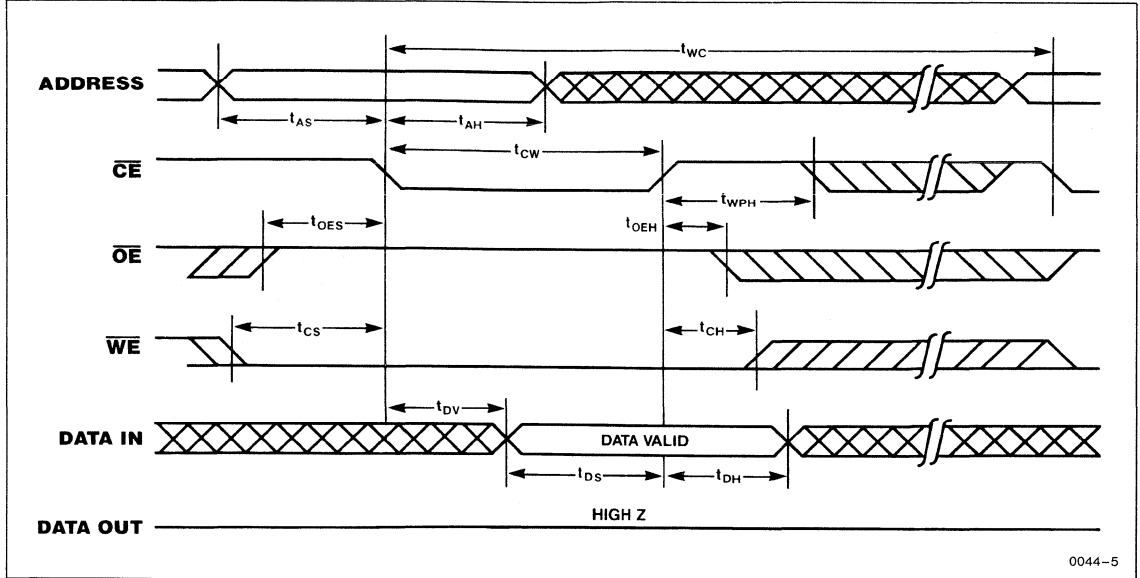
## WE Controlled Write Cycle



0044-4

# X2804A, X2804AI

## $\overline{CE}$ Controlled Write Cycle



3

# X2804A, X2804AI

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_8$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2804A through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2804A.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2804A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first.

A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms. In order to take advantage of the typical write time as opposed to the maximum specified time, the user can poll the X2804A. The I/O pins are placed in the high impedance state during the internal programming cycle. Once the internal cycle is complete, the X2804A may be accessed without any limitations. Therefore, the host can poll an address with known data (preferably with zeroes), as soon as a compare is true, the X2804A is ready for another write cycle.

## WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

## ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.



# X2804A, X2804AI

## SYSTEM CONSIDERATIONS

Because the X2804A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

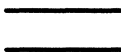




Because the X2804A has two power modes, standby and active, proper decoupling of the memory array is

of prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

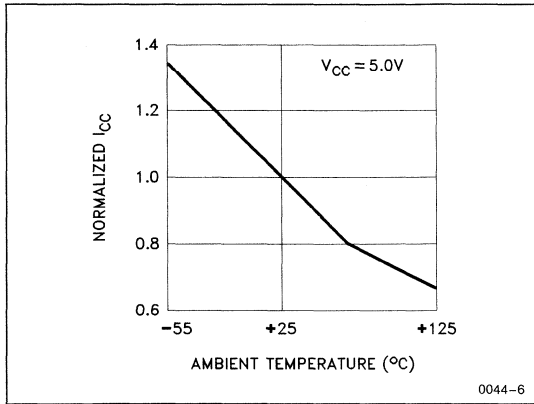
3

## SYMBOL TABLE

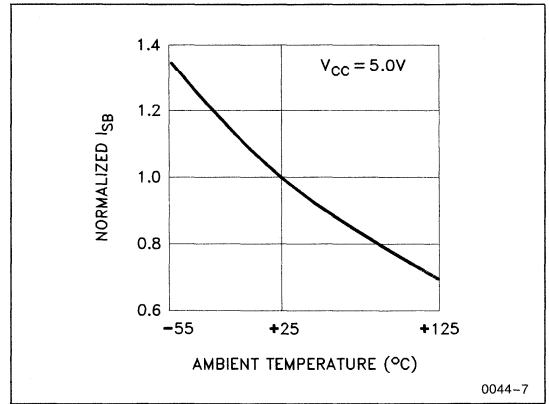
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2804A, X2804AI

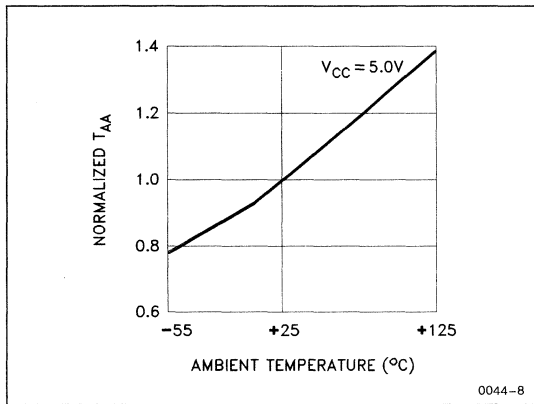
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



## Electrically Erasable PROM

### FEATURES

- Simple Byte Write Operation
  - No High Voltages Necessary
  - Single TTL Level  $\overline{WE}$  Signal Modifies Data
  - Internally Latched Address and Data
  - Self Timed Write
  - Noise Protected  $\overline{WE}$  Pin
- Reliable N-Channel Floating Gate MOS Technology
- Single 5V Supply
- Byte Write Time: 10 ms Max.
- Fast Access Time: 300 ns Max.
- Low Power Dissipation
  - Active Current: 100 mA Max.
  - Standby Current: 60 mA Max.

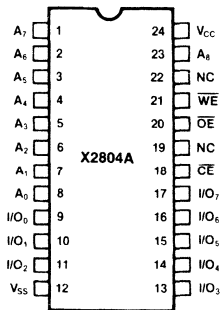
### DESCRIPTION

The Xicor X2804A is a 512 x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2804A is compatible with the JEDEC approved pinout for byte-wide memories.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.

3

### PIN CONFIGURATION

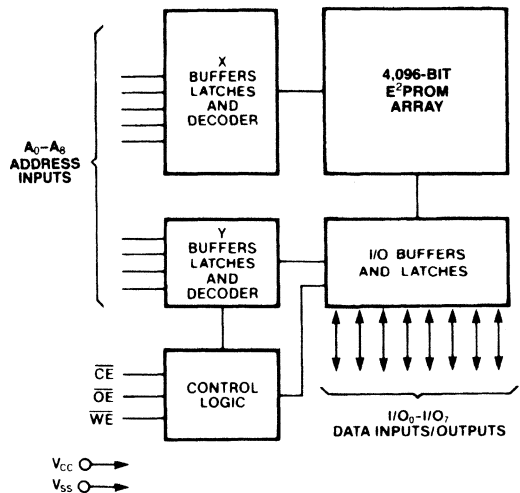


0052-1

### PIN NAMES

A <sub>0</sub> –A <sub>8</sub>	Address Inputs
I/O <sub>0</sub> –I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0052-2

# X2804AM

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias.....	-65°C to +135°C
Storage Temperature.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground.....	-1.0V to +7V
D.C. Output Current.....	5 mA
Lead Temperature (Soldering, 10 Seconds).....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		100	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.2	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -400 \mu\text{A}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2804AM

## A.C. CHARACTERISTICS

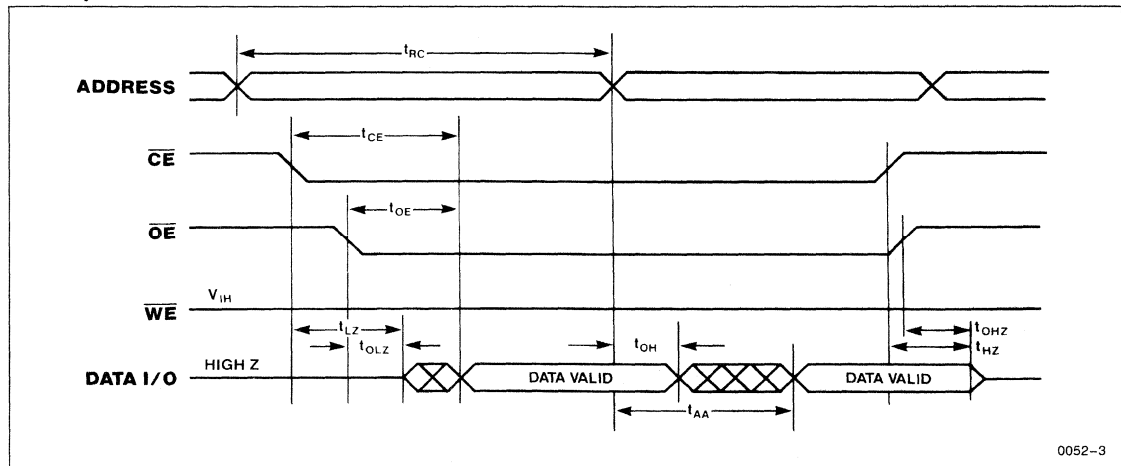
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2804AM		X2804AM-35		X2804AM-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	300		350		450		ns
$t_{CE}$	Chip Enable Access Time		300		350		450	ns
$t_{AA}$	Address Access Time		300		350		450	ns
$t_{OE}$	Output Enable Access Time		120		135		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	150	10	150	ns
$t_{OLZ}$	Output Enable to Output in Low Z	50		50		50		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	150	10	150	ns
$t_{OH}$	Output Hold from Address Change	20		20		20		ns

3

### Read Cycle



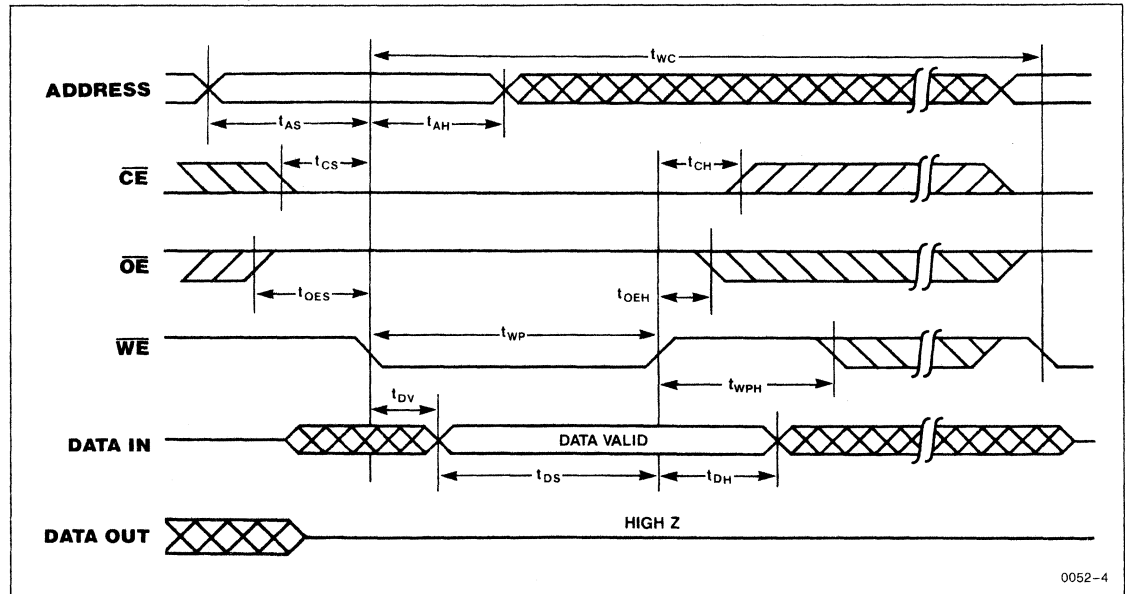
Note: (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2804AM

## Write Cycle Limits

Symbol	Parameter	X2804AM		X2804AM-35		X2804AM-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	10		10		10		ms
$t_{AS}$	Address Setup Time	10		10		10		ns
$t_{AH}$	Address Hold Time	150		150		150		ns
$t_{CS}$	Write Setup Time	0		0		0		ns
$t_{CH}$	Write Hold Time	0		0		0		ns
$t_{CW}$	Chip Enable to End of Write Input	150		175		230		ns
$t_{OES}$	Output Enable Setup Time	10		10		10		ns
$t_{OEH}$	Output Enable Hold Time	10		10		10		ns
$t_{WP}$	Write Pulse Width	150		175		230		ns
$t_{WPH}$	Write Control Recovery	50		50		50		ns
$t_{DV}$	Data Valid Time		1		1		1	$\mu$ s
$t_{DS}$	Data Setup Time	135		175		230		ns
$t_{DH}$	Data Hold Time	15		20		30		ns

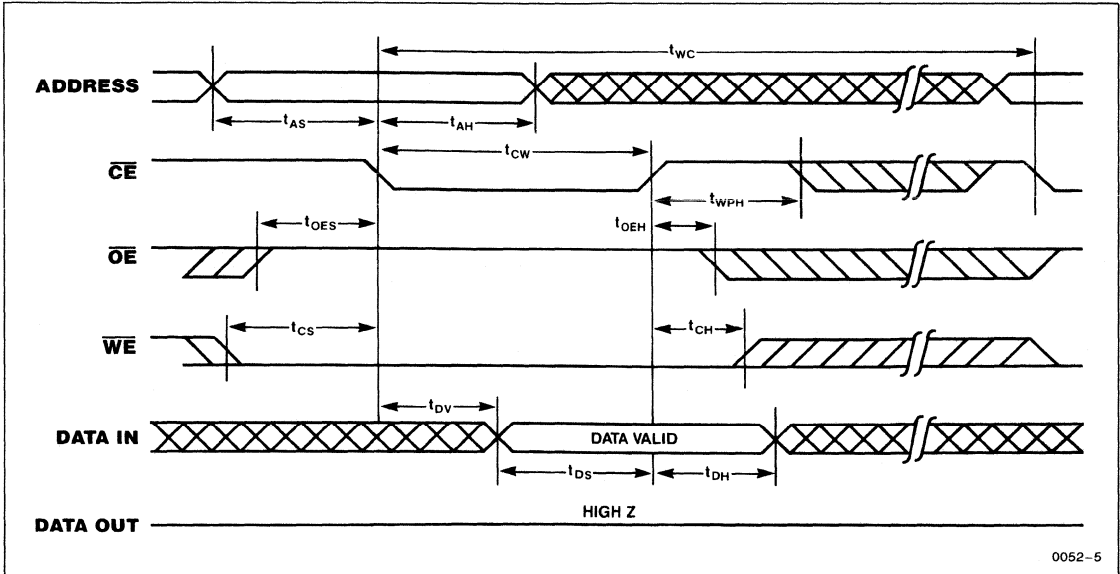
## $\overline{WE}$ Controlled Write Cycle



0052-4

# X2804AM

## $\overline{CE}$ Controlled Write Cycle



3

# X2804AM

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_8$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2804A through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2804A.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2804A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first.

A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms. In order to take advantage of the typical write time as opposed to the maximum specified time, the user can poll the X2804A. The I/O pins are placed in the high impedance state during the internal programming cycle. Once the internal cycle is complete, the X2804A may be accessed without any limitations. Therefore, the host can poll an address with known data (preferably with zeroes), as soon as a compare is true, the X2804A is ready for another write cycle.

## WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

## ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.



# X2804AM

## SYSTEM CONSIDERATIONS

Because the X2804A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

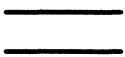




Because the X2804A has two power modes, standby and active, proper decoupling of the memory array is

of prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

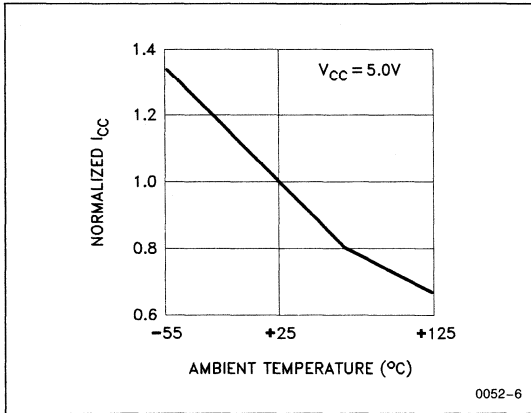
3

## SYMBOL TABLE

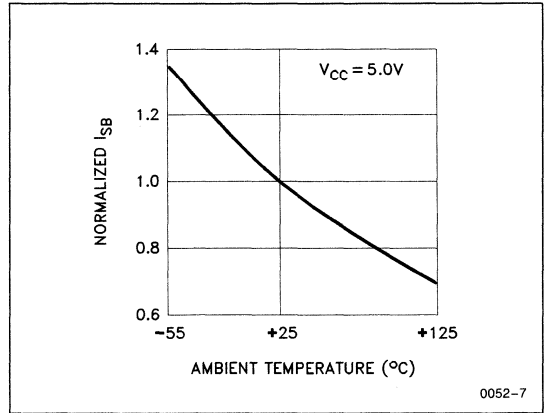
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2804AM

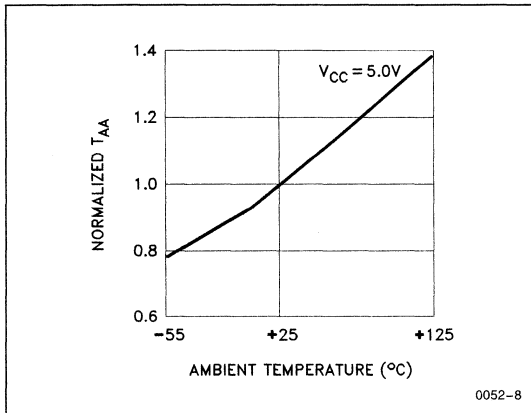
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



4K

Mil-Std-883C

X2804AMB

512 x 8 Bit

## Electrically Erasable PROM

### A.C. AND D.C. REQUIREMENTS FOR CHIP ERASE

The X2804AMB provides a mode of operation that erases the entire contents of the memory in one write cycle. This mode is entered by raising  $\overline{OE}$  to between +20V and +22V, placing all I/Os at  $V_{IH}$  and performing a standard write operation. The erasure will be completed in 10 ms.

With the exception of  $V_{OE}$ , all device A.C. and D.C. parameters are the same as those for normal operation.

*The chip erase operation is only guaranteed on Mil-Std-883C product.*

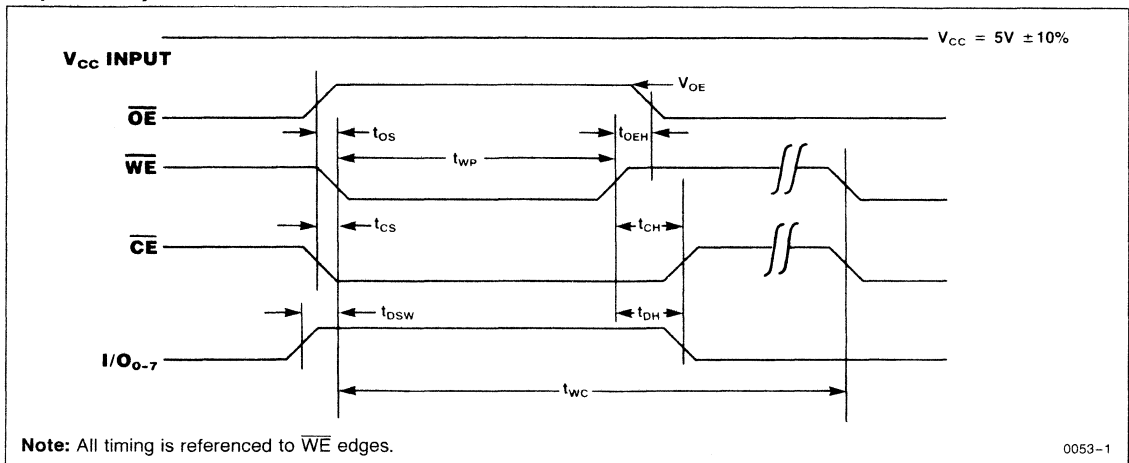
### A.C. CHIP ERASE CHARACTERISTICS

Symbol	Parameter	Limits		Units
		Min.	Max.	
$t_{CS}$	$\overline{CE}$ to $\overline{WE}$ Setup Time	10		ns
$t_{DSW}$	Data to $\overline{WE}$ Setup Time	10		ns
$t_{DH}$	Data Hold Time	50		ns
$t_{WP}$	Write Pulse Width	175		ns
$t_{CH}$	$\overline{CE}$ Hold Time	50		ns
$t_{OS}$	$V_{OE}$ Setup Time	10		ns
$t_{OEH}$	$V_{OE}$ Hold Time	10		ns
$t_{WC}$	Write Cycle Time		10	ms

### D.C. CHARACTERISTIC FOR $V_{OE}$

Symbol	Parameter	Limits		Units	Note
		Min.	Max.		
$V_{OE}$	$\overline{OE}$ Chip Erase Voltage	+20	+22	V	$I_{OE} = 10 \mu A$

### Chip Erase Cycle



3

---

## NOTES

16K

Commercial  
Industrial

X2816A  
X2816AI

2048 x 8 Bit

## Electrically Erasable PROM

### FEATURES

- Simple Byte Write Operation
  - No High Voltages Necessary
  - Single TTL Level  $\overline{WE}$  Signal Modifies Data
  - Internally Latched Address and Data
  - Self Timed Write
  - Noise Protected  $\overline{WE}$  Pin
- Reliable N-Channel Floating Gate MOS Technology
- Single 5V Supply
- Byte Write Time: 10 ms Max.
- Fast Access Time: 250 ns Max.
- Low Power Dissipation
  - Active Current: 110 mA Max.
  - Standby Current: 50 mA Max.
- JEDEC Approved Byte-Wide Pinout

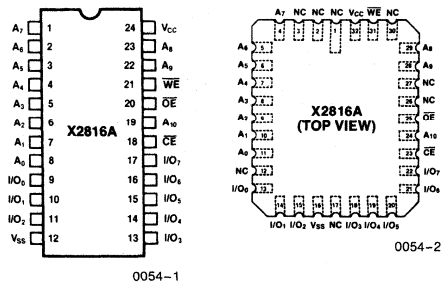
### DESCRIPTION

The Xicor X2816A is a 2K x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2816A features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs, and EPROMs.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.

3

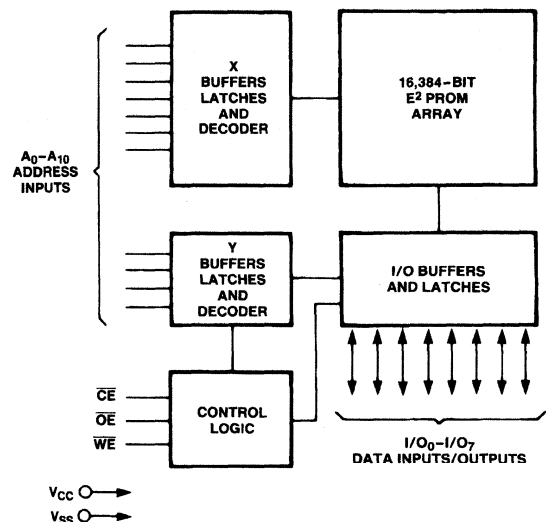
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>10</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2816A, X2816AI

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2816A	−10°C to +85°C
X2816AI	−65°C to +135°C
Storage Temperature	−65°C to +150°C
Voltage on any Pin with	
Respect to Ground	−1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature	
(Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2816A  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

X2816AI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2816A Limits		X2816AI Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		110		140	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		50		60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	−1.0	0.8	−1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 0.5$	2.2	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -400 \mu\text{A}$

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0V$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2816A, X2816AI

## A.C. CHARACTERISTICS

X2816A  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

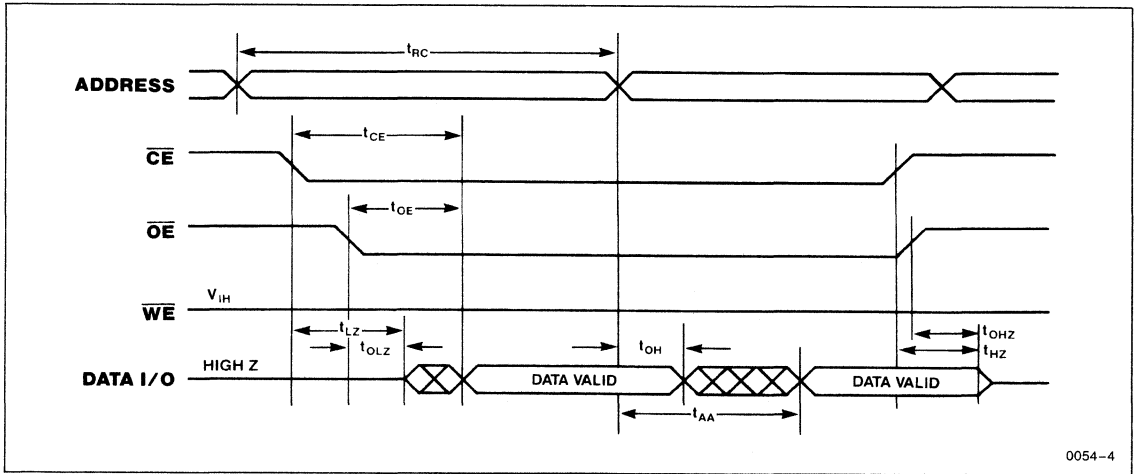
X2816AI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2816A-25 X2816AI-25		X2816A X2816AI		X2816A-35 X2816AI-35		X2816A-45 X2816AI-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		450		ns
$t_{CE}$	Chip Enable Access Time		250		300		350		450	ns
$t_{AA}$	Address Access Time		250		300		350		450	ns
$t_{OE}$	Output Enable Access Time		120		120		135		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	100	10	150	10	150	ns
$t_{OLZ}$	Output Enable to Output in Low Z	50		50		50		50		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	100	10	150	10	150	ns
$t_{OH}$	Output Hold from Address Change	20		20		20		20		ns

3

### Read Cycle



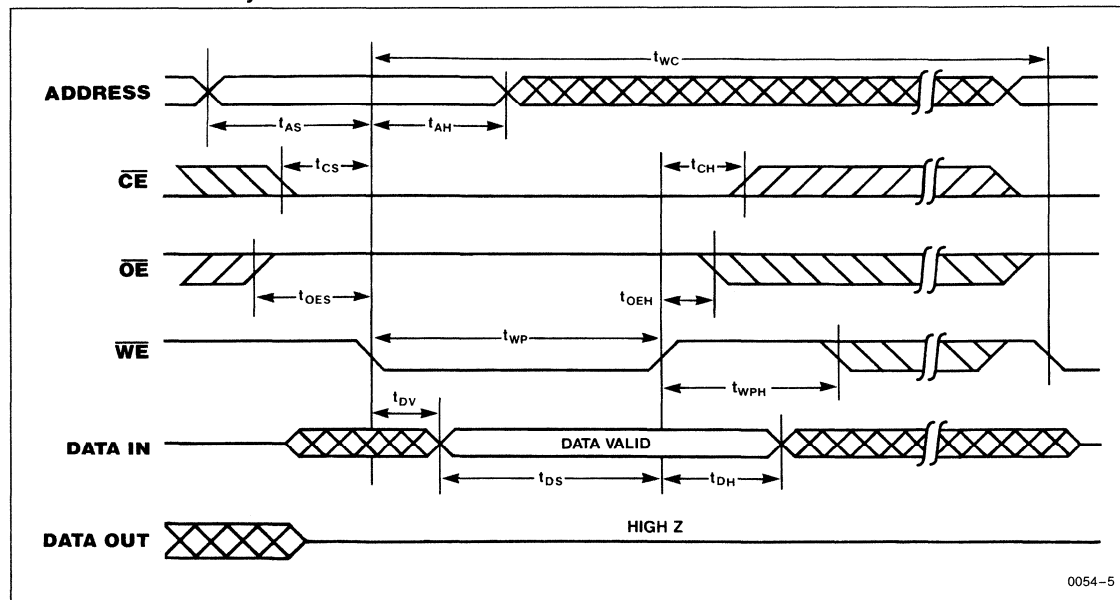
**Note:** (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2816A, X2816AI

## Write Cycle Limits

Symbol	Parameter	X2816A-25 X2816AI-25		X2816A X2816AI		X2816A-35 X2816AI-35		X2816A-45 X2816AI-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	10		10		10		10		ms
$t_{AS}$	Address Setup Time	10		10		10		10		ns
$t_{AH}$	Address Hold Time	120		120		150		150		ns
$t_{CS}$	Write Setup Time	0		0		0		0		ns
$t_{CH}$	Write Hold Time	0		0		0		0		ns
$t_{CW}$	Chip Enable to End of Write Input	150		150		175		230		ns
$t_{OES}$	Output Enable Setup Time	10		10		10		10		ns
$t_{OEH}$	Output Enable Hold Time	10		10		10		10		ns
$t_{WP}$	Write Pulse Width	150		150		175		230		ns
$t_{WPH}$	Write Control Recovery	50		50		50		50		ns
$t_{DV}$	Data Valid Time		1		1		1		1	$\mu$ s
$t_{DS}$	Data Setup Time	120		135		175		230		ns
$t_{DH}$	Data Hold Time	15		15		20		30		ns

## WE Controlled Write Cycle

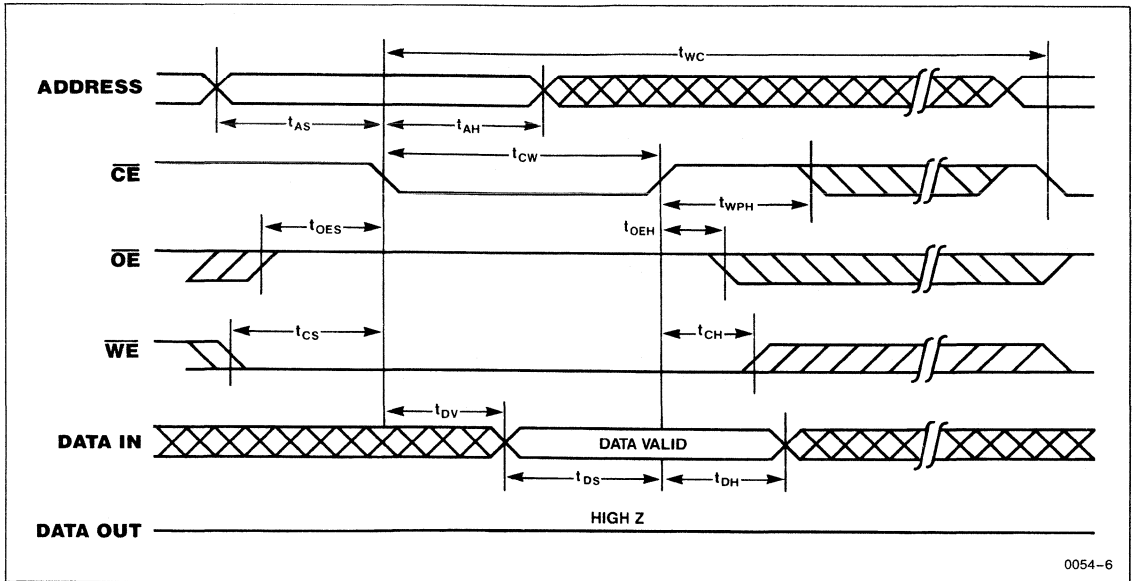


0054-5



# X2816A, X2816AI

## $\overline{\text{CE}}$ Controlled Write Cycle



3

## X2816A, X2816AI

---

### PIN DESCRIPTIONS

#### Addresses ( $A_0$ – $A_{10}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

#### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

#### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

#### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2816A through the I/O pins.

#### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2816A.

### DEVICE OPERATION

#### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

#### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2816A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first.

A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms. In order to take advantage of the typical write time as opposed to the maximum specified time, the user can poll the X2816A. The I/O pins are placed in the high impedance state during the internal programming cycle. Once the internal cycle is complete, the X2816A may be accessed without any limitations. Therefore, the host can poll an address with known data (preferably with zeroes), as soon as a compare is true, the X2816A is ready for another write cycle.

### WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

### ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

## X2816A, X2816AI

### SYSTEM CONSIDERATIONS

Because the X2816A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

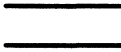




Because the X2816A has two power modes, standby and active, proper decoupling of the memory array is

of prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

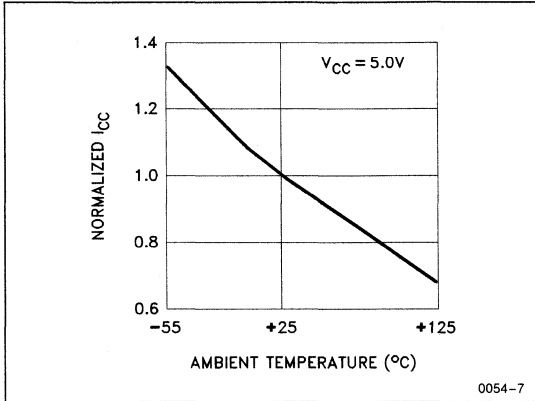
3

### SYMBOL TABLE

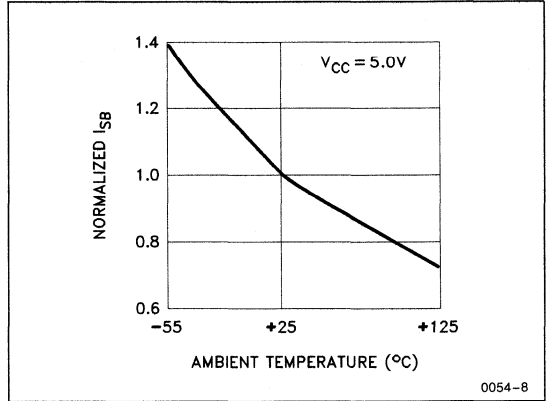
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2816A, X2816AI

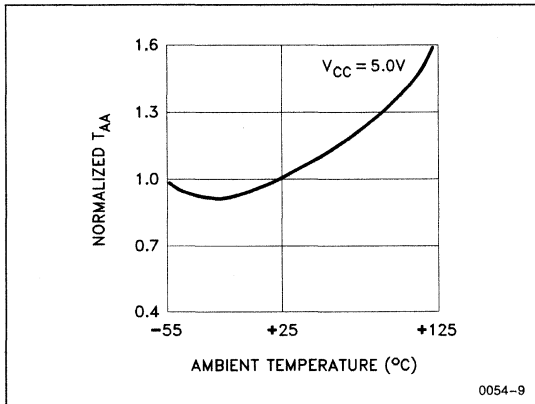
**Normalized Active Supply Current  
vs. Ambient Temperature**



**Normalized Standby Supply Current  
vs. Ambient Temperature**



**Normalized Access Time  
vs. Ambient Temperature**



## Electrically Erasable PROM

### FEATURES

- **Simple Byte Write Operation**
  - No High Voltages Necessary
  - Single TTL Level  $\overline{WE}$  Signal Modifies Data
  - Internally Latched Address and Data
  - Self Timed Write
  - Noise Protected  $\overline{WE}$  Pin
- **Reliable N-Channel Floating Gate MOS Technology**
- **Single 5V Supply**
- **Byte Write Time: 10 ms Max.**
- **Fast Access Time: 300 ns Max.**
- **Low Power Dissipation**
  - Active Current: 140 mA Max.
  - Standby Current: 60 mA Max.
- **JEDEC Approved Byte-Wide Pinout**

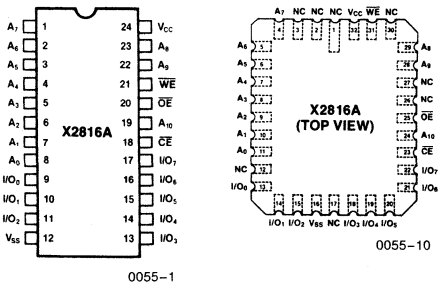
### DESCRIPTION

The Xicor X2816A is a 2K x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2816A features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs, and EPROMs.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.

3

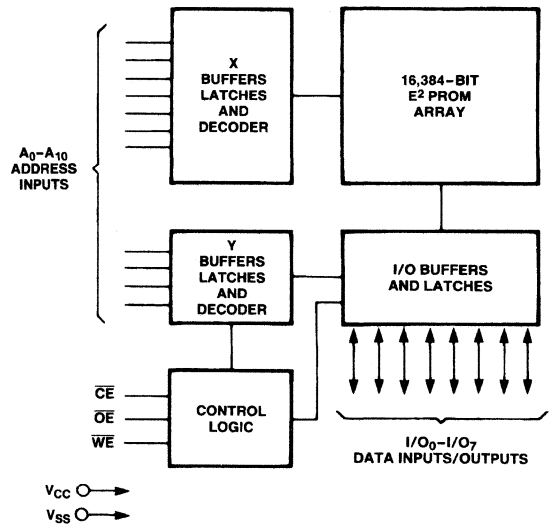
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>10</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0055-3

# X2816AM

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias.....	-65°C to +135°C
Storage Temperature.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground.....	-1.0V to +7V
D.C. Output Current.....	5 mA
Lead Temperature (Soldering, 10 Seconds).....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		140	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.2	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -400 \mu\text{A}$

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0 \text{ MHz}$ , $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(1)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(1)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Note:** (1) This parameter is periodically sampled and not 100% tested.

# X2816AM

## A.C. CHARACTERISTICS

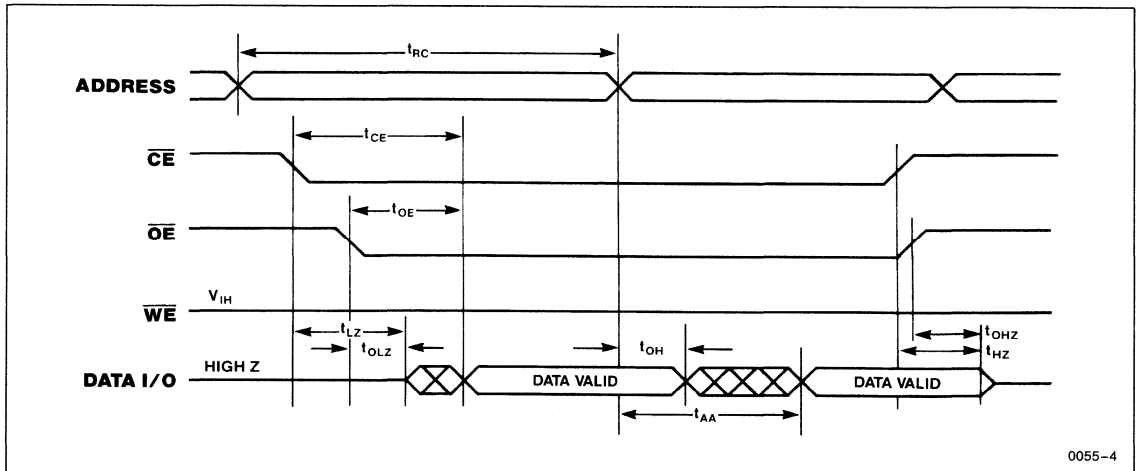
$T_A = -55^{\circ}\text{C}$  to  $+125^{\circ}\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2816AM		X2816AM-35		X2816AM-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	300		350		450		ns
$t_{CE}$	Chip Enable Access Time		300		350		450	ns
$t_{AA}$	Address Access Time		300		350		450	ns
$t_{OE}$	Output Enable Access Time		120		135		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		ns
$t_{HZ}^{(2)}$	Chip Disable to Output in High Z	10	100	10	150	10	150	ns
$t_{OLZ}$	Output Enable to Output in Low Z	50		50		50		ns
$t_{OHZ}^{(2)}$	Output Disable to Output in High Z	10	100	10	150	10	150	ns
$t_{OH}$	Output Hold from Address Change	20		20		20		ns

3

### Read Cycle



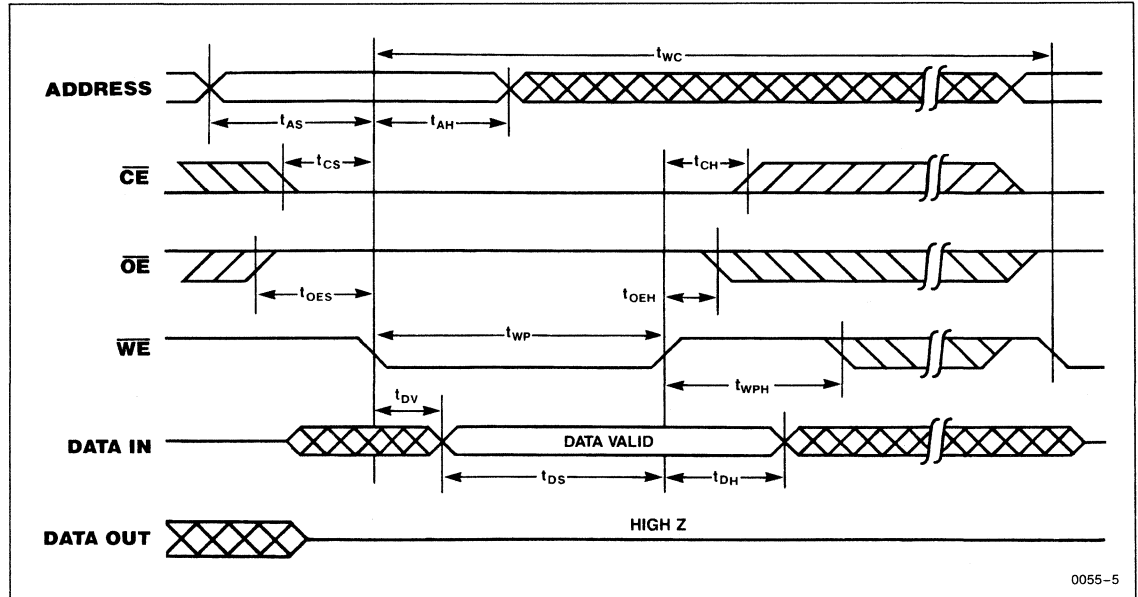
Note: (2)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2816AM

## Write Cycle Limits

Symbol	Parameter	X2816AM		X2816AM-35		X2816AM-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time	10		10		10		ms
$t_{AS}$	Address Setup Time	10		10		10		ns
$t_{AH}$	Address Hold Time	150		150		150		ns
$t_{CS}$	Write Setup Time	0		0		0		ns
$t_{CH}$	Write Hold Time	0		0		0		ns
$t_{CW}$	Chip Enable to End of Write Input	150		175		230		ns
$t_{OES}$	Output Enable Setup Time	10		10		10		ns
$t_{OEH}$	Output Enable Hold Time	10		10		10		ns
$t_{WP}$	Write Pulse Width	150		175		230		ns
$t_{WPH}$	Write Control Recovery	50		50		50		ns
$t_{DV}$	Data Valid Time		1		1		1	$\mu$ s
$t_{DS}$	Data Setup Time	135		175		230		ns
$t_{DH}$	Data Hold Time	15		20		30		ns

## $\overline{WE}$ Controlled Write Cycle

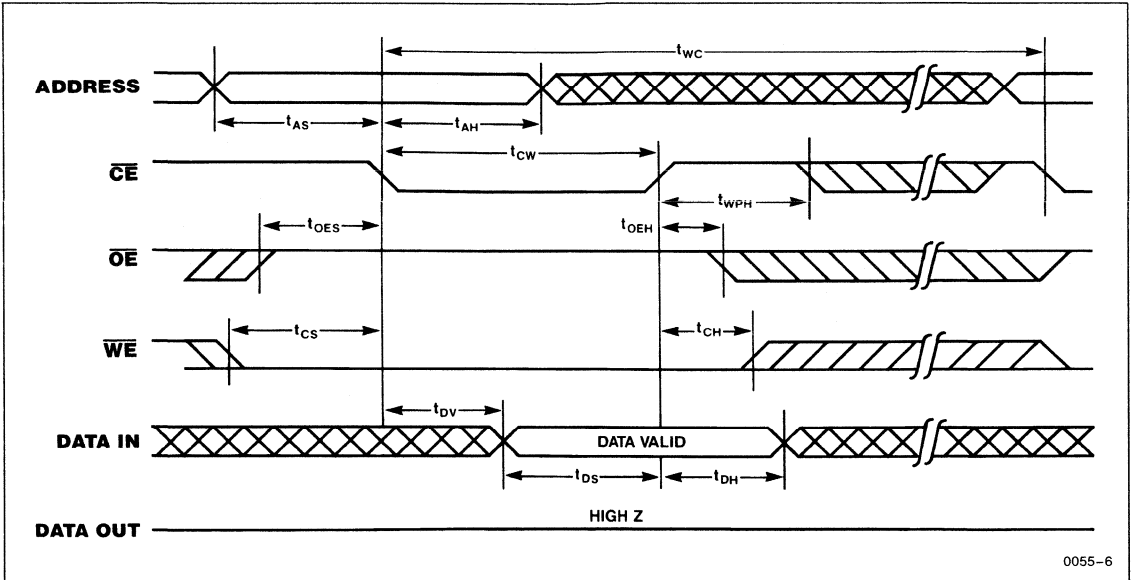


0055-5



# X2816AM

## $\overline{CE}$ Controlled Write Cycle



3

# X2816AM

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{10}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2816A through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2816A.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2816A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first.

A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms. In order to take advantage of the typical write time as opposed to the maximum specified time, the user can poll the X2816A. The I/O pins are placed in the high impedance state during the internal programming cycle. Once the internal cycle is complete, the X2816A may be accessed without any limitations. Therefore, the host can poll an address with known data (preferably with zeroes), as soon as a compare is true, the X2816A is ready for another write cycle.

## WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

## ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

# X2816AM

## SYSTEM CONSIDERATIONS

Because the X2816A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.






Because the X2816A has two power modes, standby and active, proper decoupling of the memory array is

of prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

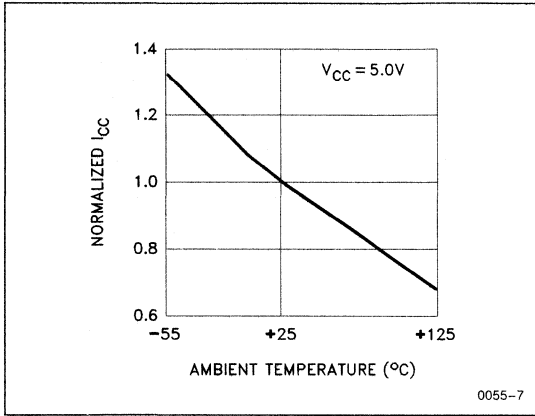
3

## SYMBOL TABLE

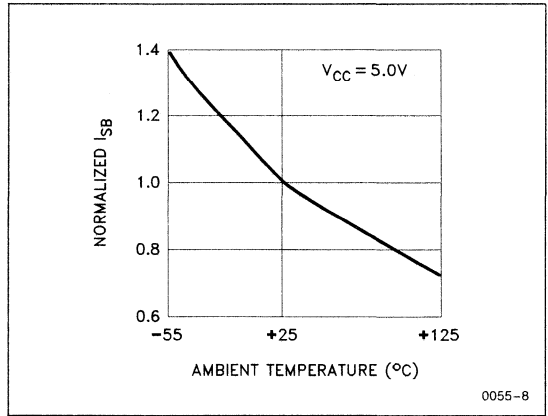
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2816AM

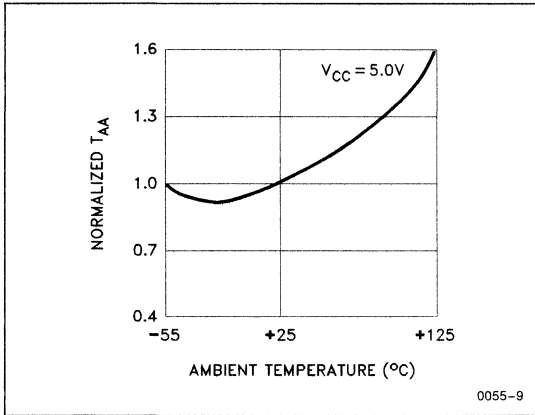
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



**16K Commercial Industrial X2816B X2816BI 2048 x 8 Bit**

---

**Electrically Erasable PROM**

---

**FEATURES**

- **250 ns Access Time**
- **High Performance Advanced NMOS Technology**
- **Fast Write Cycle Times**
  - 16-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 640 ms Typical
  - Effective Byte Write Cycle Time of 300  $\mu$ s Typical
- **DATA Polling**
  - Allows User to Minimize Write Cycle Time
- **Simple Byte and Page Write**
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **JEDEC Approved Byte-Wide Pinout**

**DESCRIPTION**

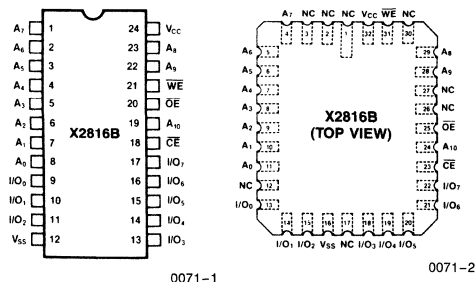
The Xicor X2816B is a 2K x 8 E<sup>2</sup>PROM, fabricated with an advanced, high performance N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories it is a 5V only device. The X2816B features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2816B supports a 16-byte page write operation, typically providing a 300  $\mu$ s/byte write cycle, enabling the entire memory to be written in less than 640 ms. The X2816B also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 100 years.

3

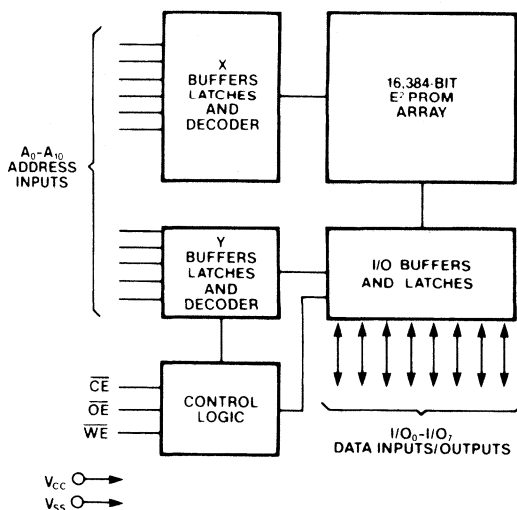
**PIN CONFIGURATIONS**



**PIN NAMES**

A <sub>0</sub> -A <sub>10</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
CE	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

**FUNCTIONAL DIAGRAM**



0071-3

# X2816B, X2816BI

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2816B	-10°C to +85°C
X2816BI	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2816B  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

X2816BI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2816B/X2816B-25 Limits			X2816BI/X2816BI-25 Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.	Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80	120		80	140	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		45	60		45	70	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0V$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2816B, X2816BI

## A.C. CHARACTERISTICS

X2816B  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

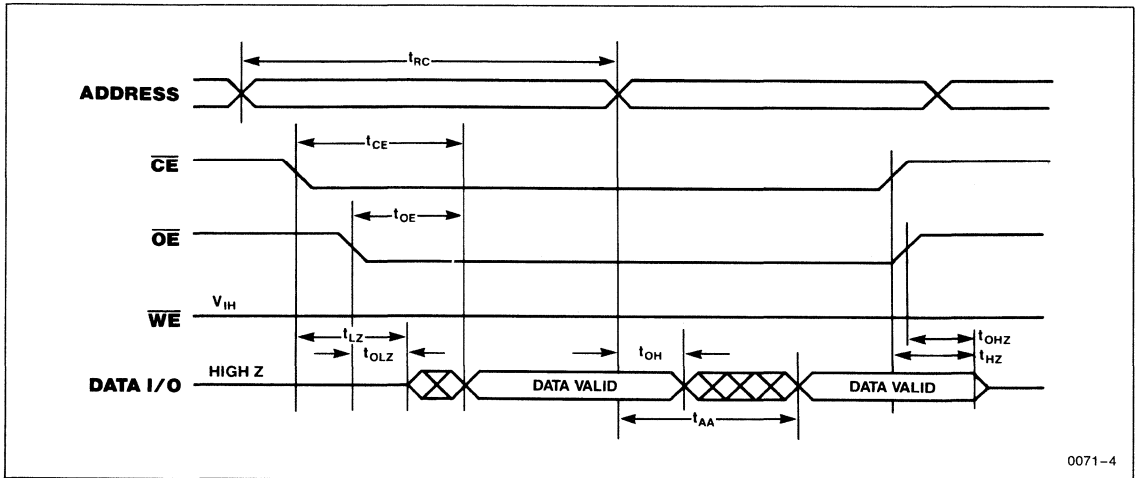
X2816BI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2816B-25 X2816BI-25		X2816B X2816BI		Units
		Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		ns
$t_{CE}$	Chip Enable Access Time		250		300	ns
$t_{AA}$	Address Access Time		250		300	ns
$t_{OE}$	Output Enable Access Time		100		100	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		ns
$t_{HZ}^{(3)}$	Chip Disable to Output in High Z	10	60	10	80	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		ns
$t_{OHZ}^{(3)}$	Output Disable to Output in High Z	10	60	10	80	ns
$t_{OH}$	Output Hold from Address Change	10		10		ns

3

### Read Cycle



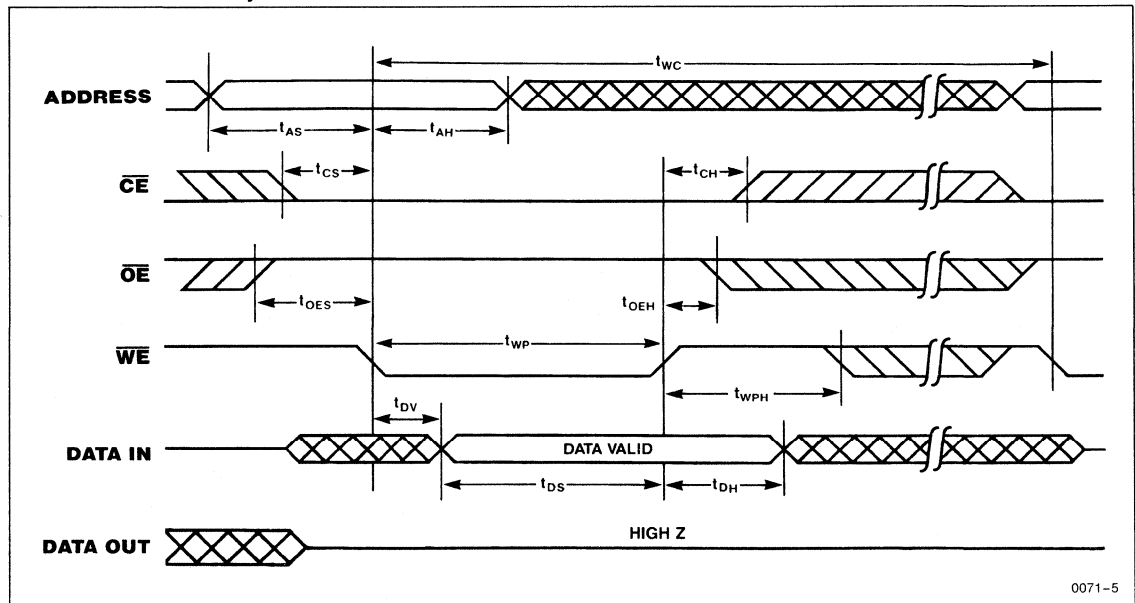
Note: (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2816B, X2816BI

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		5	10	ms
$t_{AS}$	Address Setup Time	10			ns
$t_{AH}$	Address Hold Time	150			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	150			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	150			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	50			ns
$t_{DV}$	Data Valid			300	ns
$t_{DS}$	Data Setup	100			ns
$t_{DH}$	Data Hold	15			ns
$t_{DW}$	Delay to Next Write	500			$\mu$ s
$t_{BLC}$	Byte Load Cycle	3		20	$\mu$ s

## $\overline{WE}$ Controlled Write Cycle

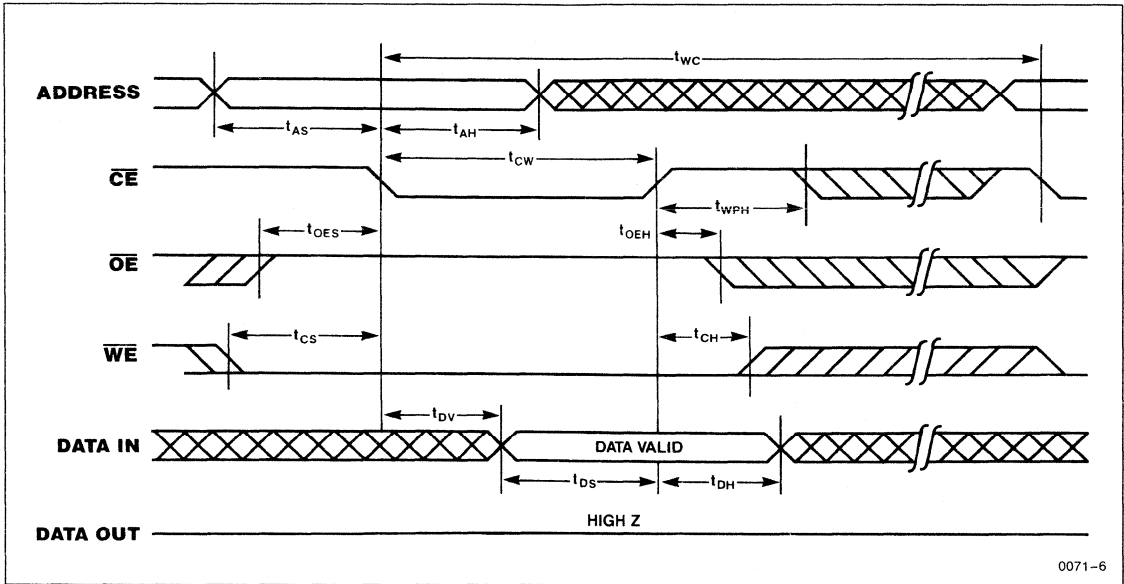


Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.



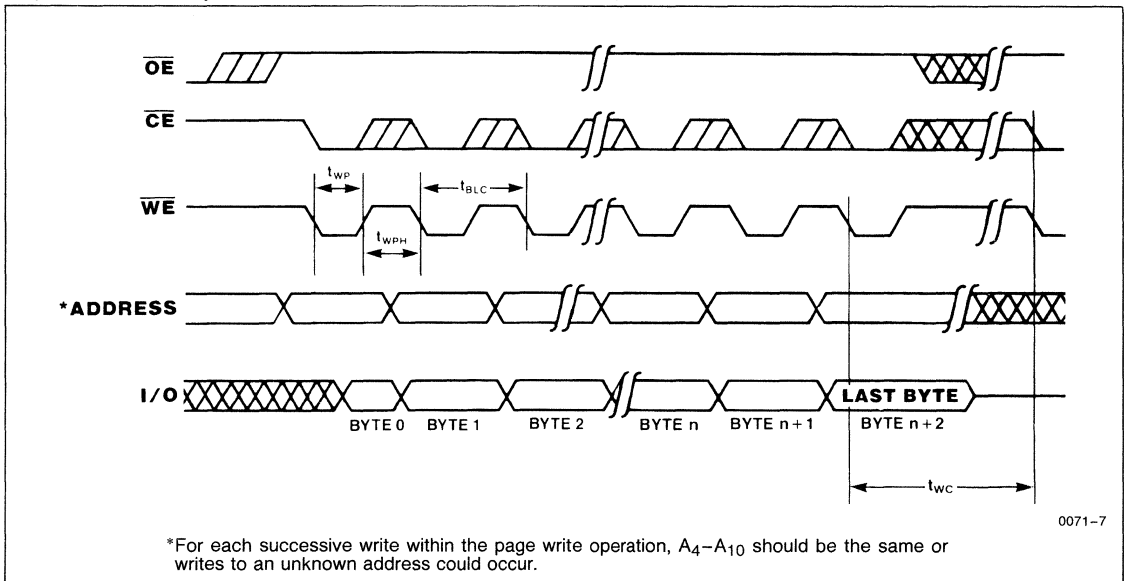
# X2816B, X2816BI

## CE Controlled Write Cycle



3

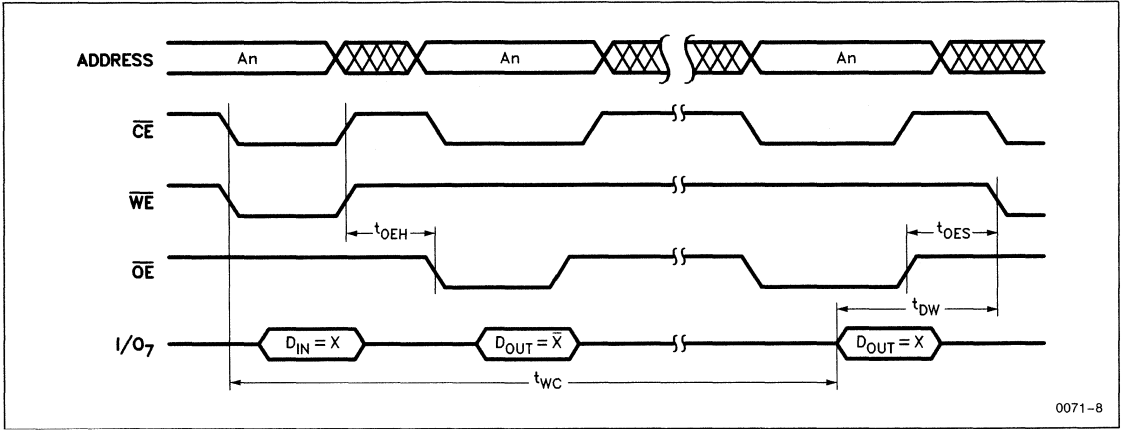
## Page Mode Write Cycle



\*For each successive write within the page write operation, A<sub>4</sub>-A<sub>10</sub> should be the same or writes to an unknown address could occur.

# X2816B, X2816BI

## DATA Polling Timing Diagram



## X2816B, X2816BI

---

### PIN DESCRIPTIONS

#### Addresses ( $A_0$ – $A_{10}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

#### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

#### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

#### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2816B through the I/O pins.

#### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2816B.

### DEVICE OPERATION

#### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

#### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2816B supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

#### Page Write Operation

The page write feature of the X2816B allows the entire memory to be typically written in 640 ms. Page write allows two to sixteen bytes of data to be consecutively written to the X2816B prior to the commencement of the internal programming cycle. Although the host system may read data from any location in the system to transfer to the X2816B, the destination page address of the X2816B should be the same on each subsequent strobe of the  $\overline{WE}$  and  $\overline{CE}$  inputs. That is,  $A_4$

through  $A_{10}$  must be the same for each transfer of data to the X2816B during a page write cycle.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to fifteen bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 20  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 20  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. The page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 20  $\mu$ s.

#### $\overline{DATA}$ Polling

The X2816B features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2816B, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

#### WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

#### ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

## X2816B, X2816BI

### SYSTEM CONSIDERATIONS

Because the X2816B is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.






To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2816B has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

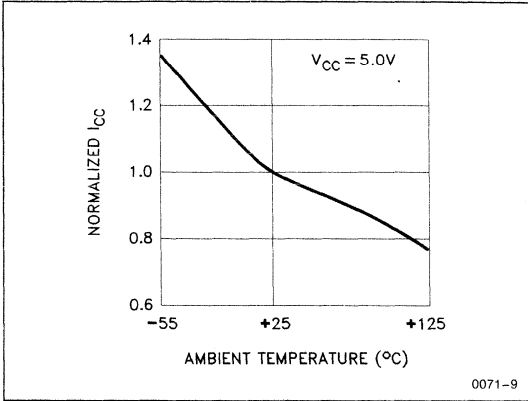
In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

**SYMBOL TABLE**

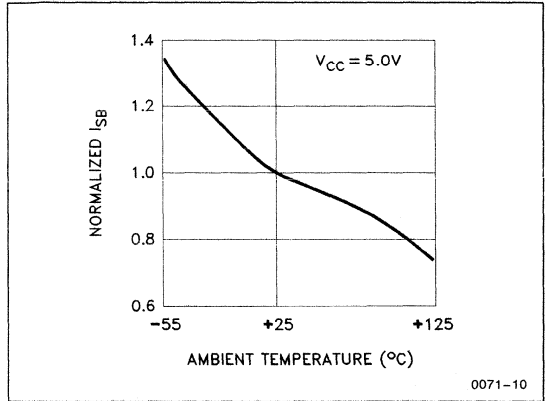
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2816B, X2816BI

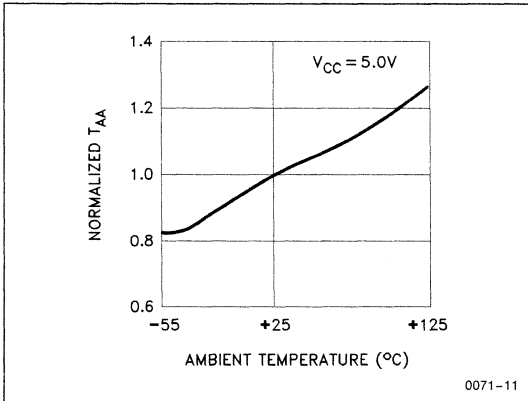
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



3

---

## NOTES

## Electrically Erasable PROM

### FEATURES

- 250 ns Access Time
- High Performance Advanced NMOS Technology
- Fast Write Cycle Times
  - 16-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 640 ms Typical
  - Effective Byte Write Cycle Time of 300  $\mu$ s Typical
- DATA Polling
  - Allows User to Minimize Write Cycle Time
- Simple Byte and Page Write
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- JEDEC Approved Byte-Wide Pinout

### DESCRIPTION

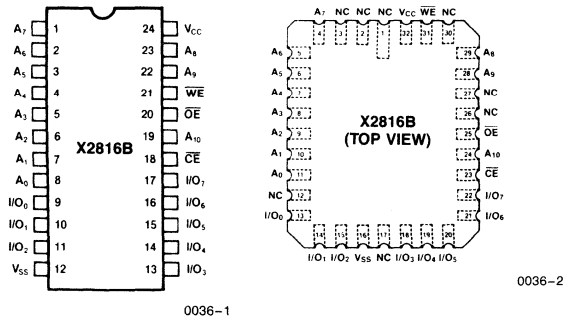
The Xicor X2816B is a 2K x 8 E<sup>2</sup>PROM, fabricated with an advanced, high performance N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories it is a 5V only device. The X2816B features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2816B supports a 16-byte page write operation, typically providing a 300  $\mu$ s/byte write cycle, enabling the entire memory to be written in less than 640 ms. The X2816B also features DATA Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 100 years.

3

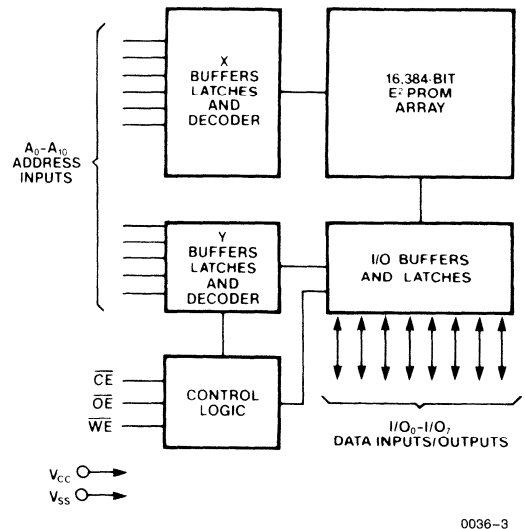
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>10</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
CE	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2816BM

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias .....	-65°C to +135°C
Storage Temperature .....	-65°C to +150°C
Voltage on any Pin with Respect to Ground .....	-1.0V to +7V
D.C. Output Current .....	5 mA
Lead Temperature (Soldering, 10 Seconds) .....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80	140	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		45	70	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.



# X2816BM

## A.C. CHARACTERISTICS

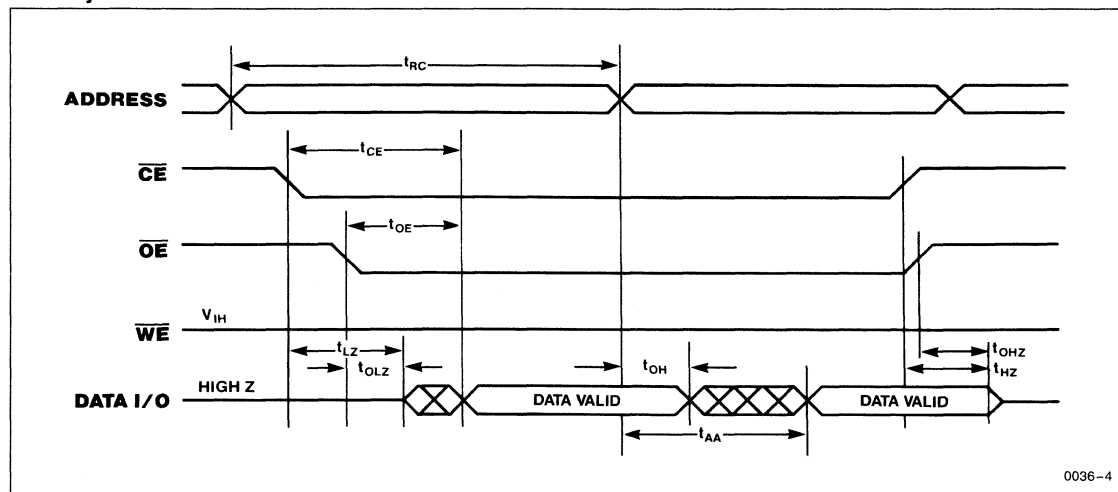
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2816BM-25		X2816BM		Units
		Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		ns
$t_{CE}$	Chip Enable Access Time		250		300	ns
$t_{AA}$	Address Access Time		250		300	ns
$t_{OE}$	Output Enable Access Time		100		100	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		ns
$t_{HZ}^{(3)}$	Chip Disable to Output in High Z	10	60	10	80	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		ns
$t_{OHZ}^{(3)}$	Output Disable to Output in High Z	10	60	10	80	ns
$t_{OH}$	Output Hold from Address Change	10		10		ns

3

### Read Cycle



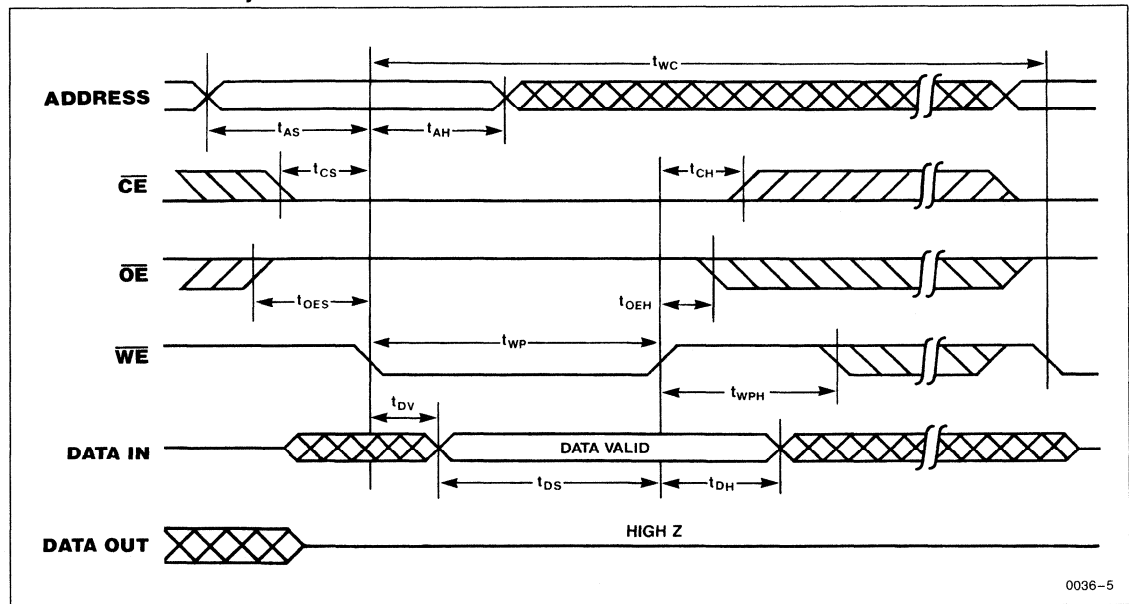
Note: (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2816BM

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		5	10	ms
$t_{AS}$	Address Setup Time	10			ns
$t_{AH}$	Address Hold Time	150			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	150			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	150			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	50			ns
$t_{DV}$	Data Valid			300	ns
$t_{DS}$	Data Setup	100			ns
$t_{DH}$	Data Hold	15			ns
$t_{DW}$	Delay to Next Write	500			$\mu$ s
$t_{BLC}$	Byte Load Cycle	3		20	$\mu$ s

## $\overline{WE}$ Controlled Write Cycle

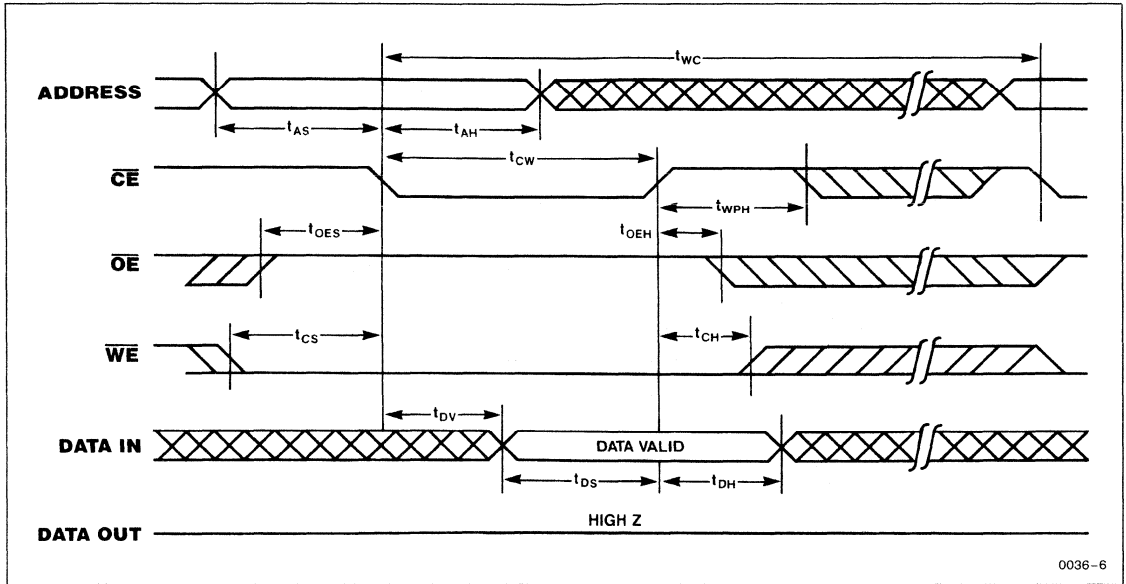


0036-5

Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

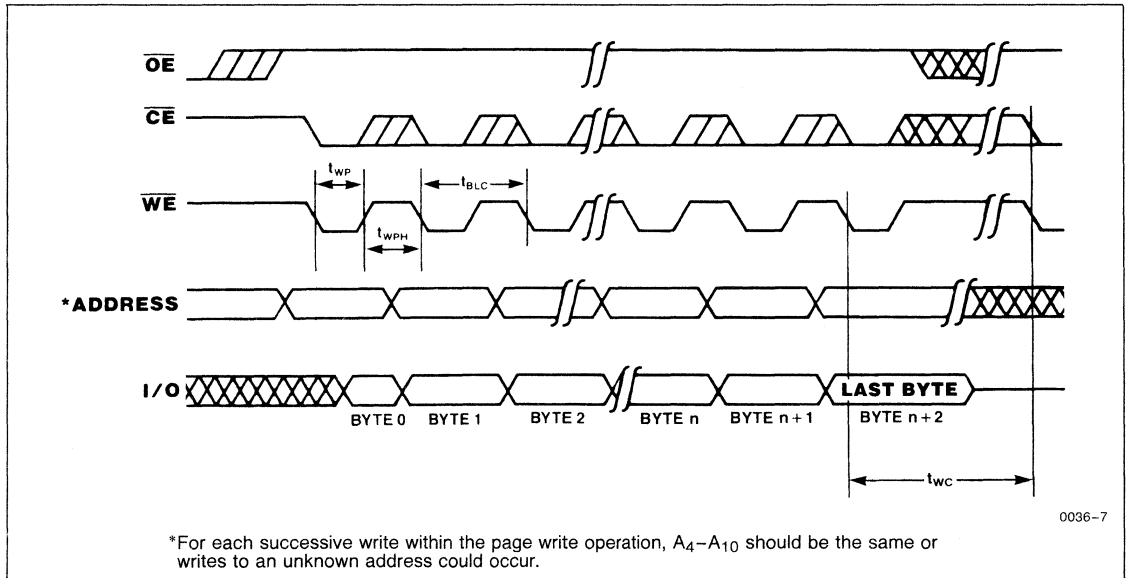
# X2816BM

## $\overline{CE}$ Controlled Write Cycle



3

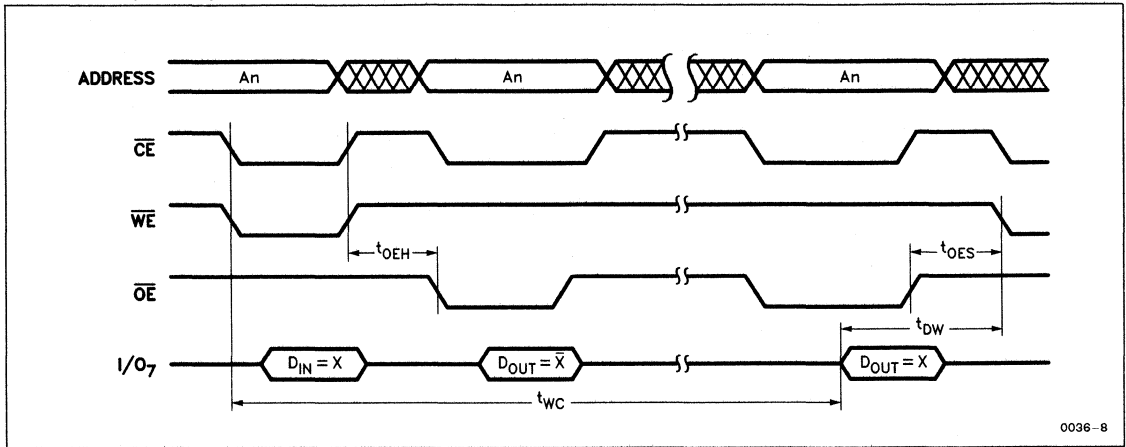
## Page Mode Write Cycle



\*For each successive write within the page write operation,  $A_4-A_{10}$  should be the same or writes to an unknown address could occur.

# X2816BM

## DATA Polling Timing Diagram



# X2816BM

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{10}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2816B through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2816B.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2816B supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

The page write feature of the X2816B allows the entire memory to be typically written in 640 ms. Page write allows two to sixteen bytes of data to be consecutively written to the X2816B prior to the commencement of the internal programming cycle. Although the host system may read data from any location in the system to transfer to the X2816B, the destination page address of the X2816B should be the same on each subsequent strobe of the  $\overline{WE}$  and  $\overline{CE}$  inputs. That is,  $A_4$

through  $A_{10}$  must be the same for each transfer of data to the X2816B during a page write cycle.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to fifteen bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 20  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 20  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. The page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 20  $\mu$ s.

### DATA Polling

The X2816B features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2816B, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

### WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

### ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is approximately 1/2 million cycles, as documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

3

## X2816BM

---

### SYSTEM CONSIDERATIONS

Because the X2816B is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

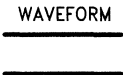




To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2816B has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

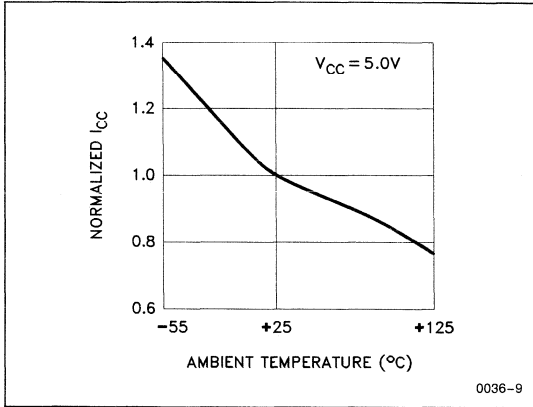
In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

### SYMBOL TABLE

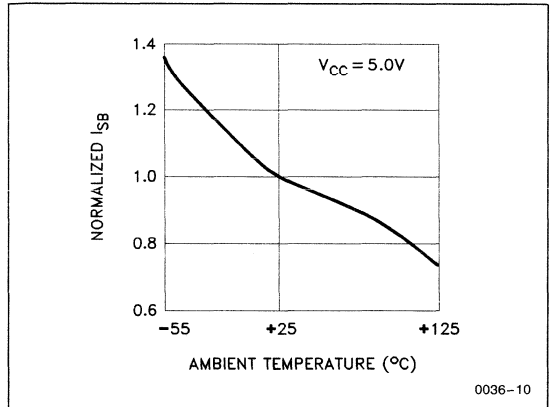
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2816BM

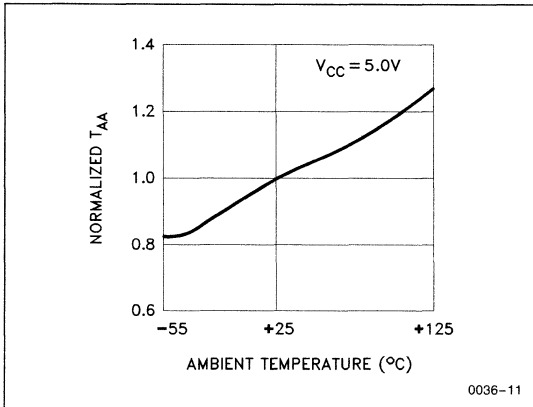
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



---

**NOTES**



16K

Mil-Std-883C

X2816BMB

2048 x 8 Bit

**Electrically Erasable PROM**

**A.C. AND D.C. REQUIREMENTS FOR CHIP ERASE**

The X2816BMB provides a mode of operation that erases the entire contents of the memory in one write cycle. This mode is entered by raising  $\overline{OE}$  to between +20V and +22V, placing all I/Os at  $V_{IH}$  and performing a standard write operation. The erasure will be completed in 10 ms.

With the exception of  $V_{OE}$ , all device A.C. and D.C. parameters are the same as those for normal operation.

*The chip erase operation is only guaranteed on Mil-Std-883C product.*

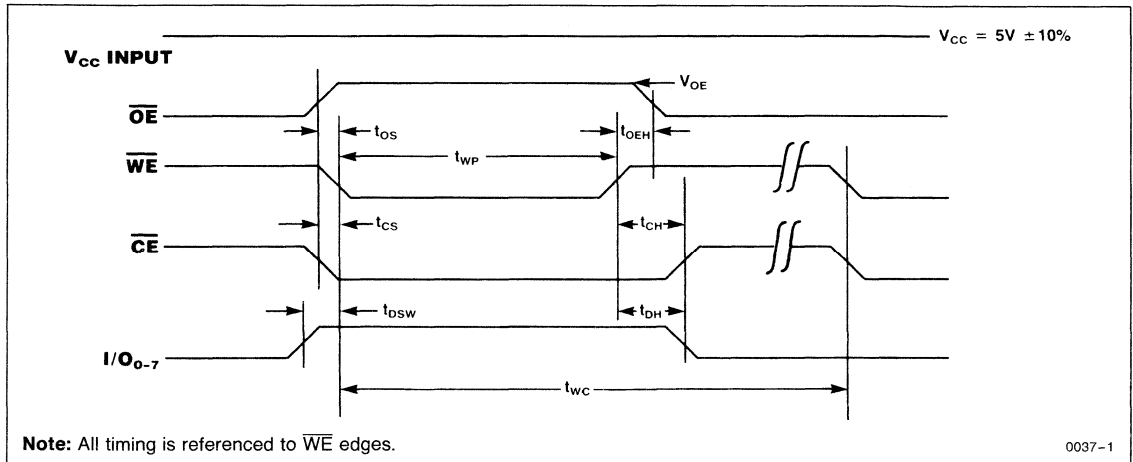
**A.C. CHIP ERASE CHARACTERISTICS**

Symbol	Parameter	Limits		Units
		Min.	Max.	
$t_{CS}$	$\overline{CE}$ to $\overline{WE}$ Setup Time	10		ns
$t_{DSW}$	Data to $\overline{WE}$ Setup Time	10		ns
$t_{DH}$	Data Hold Time	50		ns
$t_{WP}$	Write Pulse Width	175		ns
$t_{CH}$	$\overline{CE}$ Hold Time	50		ns
$t_{OS}$	$V_{OE}$ Setup Time	10		ns
$t_{OEH}$	$V_{OE}$ Hold Time	10		ns
$t_{WC}$	Write Cycle Time		10	ms

**D.C. CHARACTERISTIC FOR  $V_{OE}$**

Symbol	Parameter	Limits		Units	Note
		Min.	Max.		
$V_{OE}$	$\overline{OE}$ Chip Erase Voltage	+20	+22	V	$I_{OE} = 10 \mu A$

**Chip Erase Cycle**



3

---

## NOTES

## Electrically Erasable PROM

### FEATURES

- **250 ns Access Time**
- **Fast Write Cycle Times**
  - 16-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 2.6 Sec. Typical
  - Effective Byte Write Cycle Time of 300  $\mu$ s Typical
- **DATA Polling**
  - Allows User to Minimize Write Cycle Time
- **Simple Byte and Page Write**
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **JEDEC Approved Byte-Wide Pinout**

### DESCRIPTION

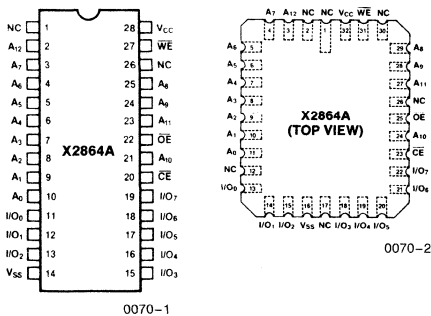
The Xicor X2864A is a 8K x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2864A features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2864A supports a 16-byte page write operation, effectively providing a 300  $\mu$ s/byte write and enabling the entire memory to be written in less than 2.6 seconds. The X2864A also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.

**3**

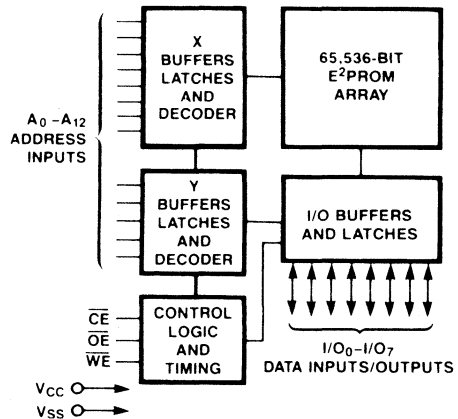
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
CE	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2864A, X2864AI

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2864A	–10°C to +85°C
X2864AI	–65°C to +135°C
Storage Temperature	–65°C to +150°C
Voltage on any Pin with Respect to Ground	–1.0V to +7V
D.C. Output Current	.5 mA
Lead Temperature (Soldering, 10 Seconds)	.300°C

## \*COMMENT

Stresses above those listed under “Absolute Maximum Ratings” may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2864A  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X2864AI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	X2864A Limits		X2864AI Limits		Units	Test Conditions
		Min.	Max.	Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		140		140	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		60		70	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	–1.0	0.8	–1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 0.5$	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4		0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		2.4		V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2864A, X2864AI

## A.C. CHARACTERISTICS

X2864A  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

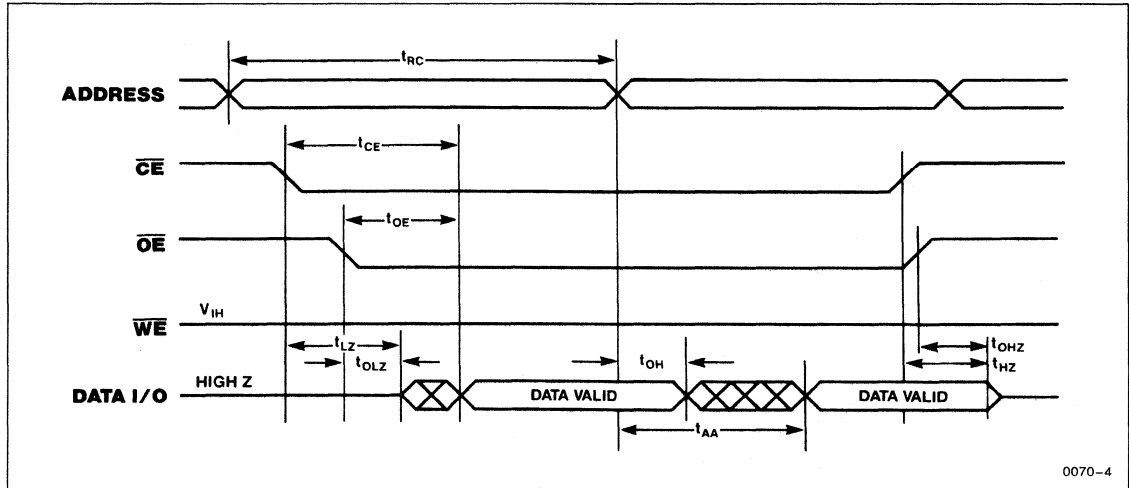
X2864AI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2864A-25 X2864AI-25		X2864A X2864AI		X2864A-35 X2864AI-35		X2864A-45 X2864AI-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		450		ns
$t_{CE}$	Chip Enable Access Time		250		300		350		450	ns
$t_{AA}$	Address Access Time		250		300		350		450	ns
$t_{OE}$	Output Enable Access Time		100		100		100		100	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		10		ns
$t_{HZ}^{(3)}$	Chip Disable to Output in High Z	10	60	10	80	10	80	10	100	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		10		10		ns
$t_{OHZ}^{(3)}$	Output Disable to Output in High Z	10	60	10	80	10	80	10	100	ns
$t_{OH}$	Output Hold from Address Change	10		10		10		10		ns

3

### Read Cycle



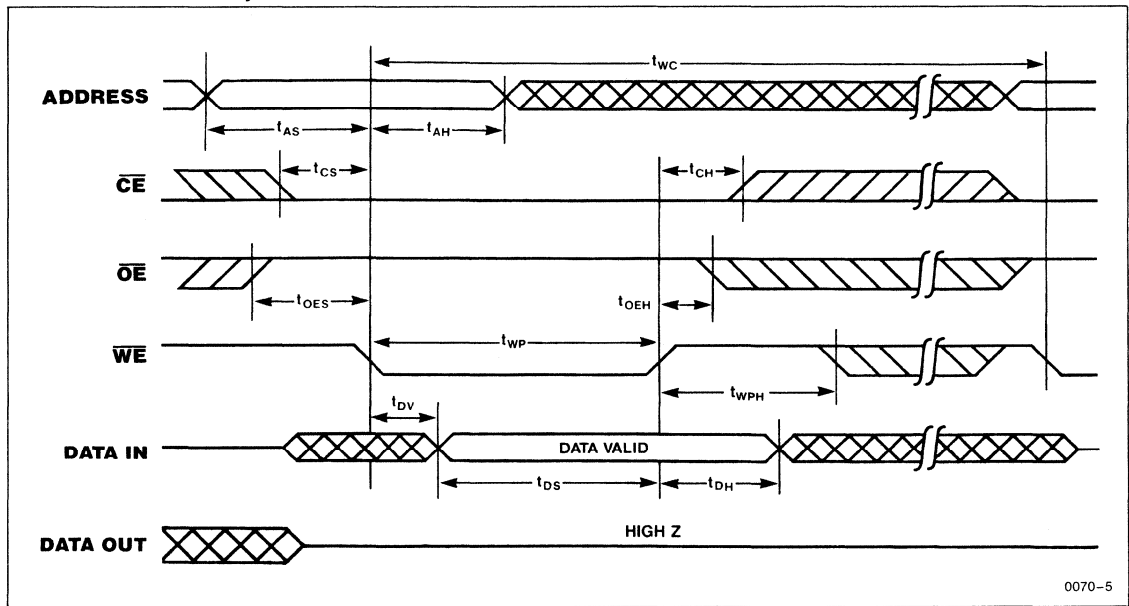
Note: (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864A, X2864AI

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	10		ms
$t_{AS}$	Address Setup Time	10		ns
$t_{AH}$	Address Hold Time	200		ns
$t_{CS}$	Write Setup Time	0		ns
$t_{CH}$	Write Hold Time	0		ns
$t_{CW}$	$\overline{CE}$ Pulse Width	150		ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10		ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10		ns
$t_{WP}$	$\overline{WE}$ Pulse Width	150		ns
$t_{WPH}$	$\overline{WE}$ High Recovery	50		ns
$t_{DV}$	Data Valid		300	ns
$t_{DS}$	Data Setup	100		ns
$t_{DH}$	Data Hold	20		ns
$t_{DW}$	Delay to Next Write	500		$\mu$ s
$t_{BLC}$	Byte Load Cycle	3	40	$\mu$ s

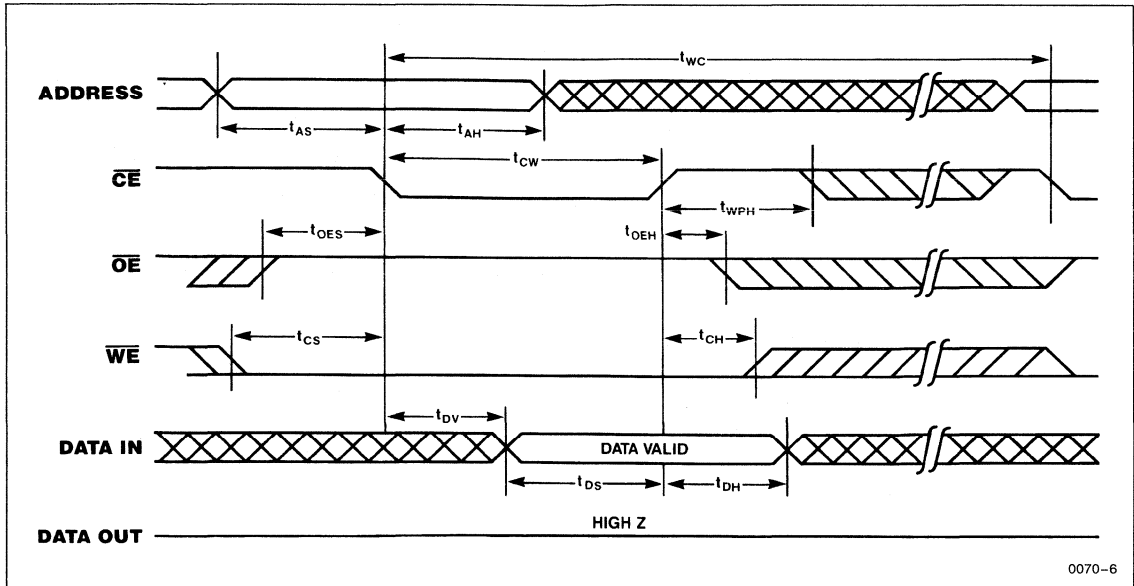
## $\overline{WE}$ Controlled Write Cycle



0070-5

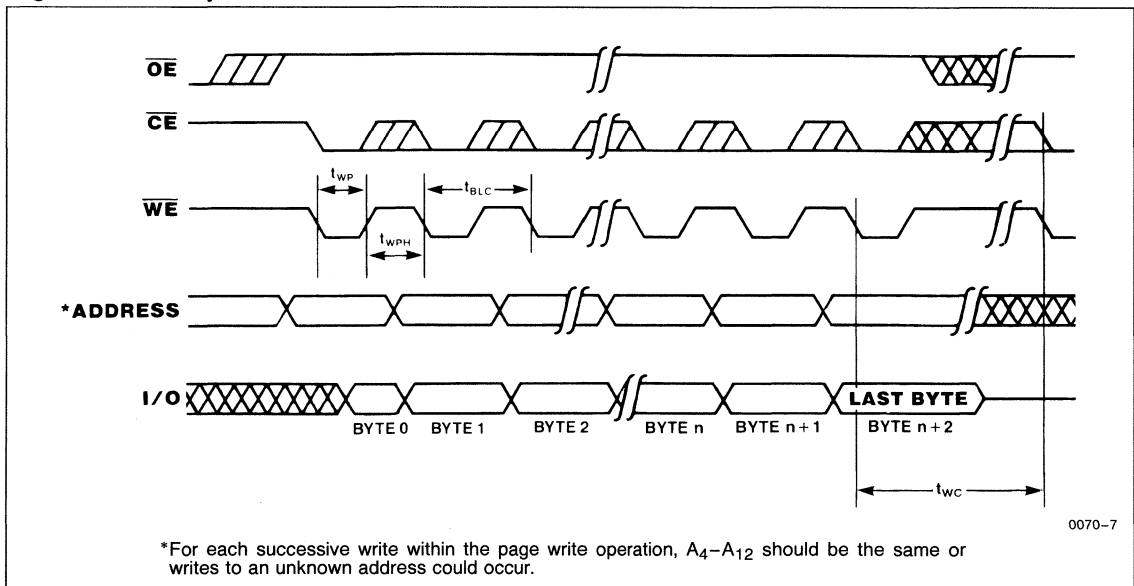
# X2864A, X2864AI

## $\overline{\text{CE}}$ Controlled Write Cycle



3

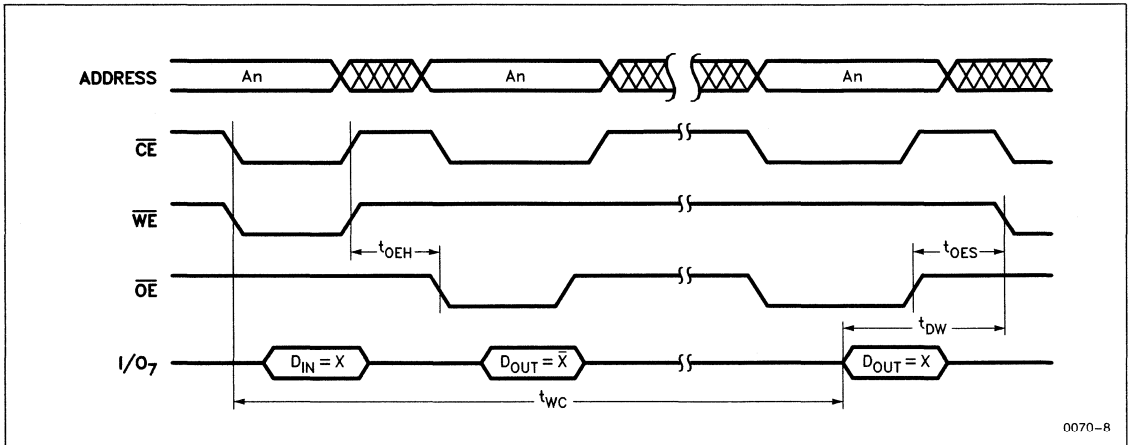
## Page Mode Write Cycle



\*For each successive write within the page write operation,  $A_4$ - $A_{12}$  should be the same or writes to an unknown address could occur.

# X2864A, X2864AI

## DATA Polling Timing Diagram





# X2864A, X2864AI

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{12}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2864A through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864A.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

The page write feature of the X2864A allows the entire memory to be written in 2.6 seconds. Page write allows two to sixteen bytes of data to be consecutively written to the X2864A prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is,  $A_4$  through  $A_{12}$  must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to fifteen bytes in the same manner as the first byte was written. Each successive byte write cycle must begin within 20  $\mu$ s of the falling edge of  $\overline{WE}$  of the preceding cycle. If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 20  $\mu$ s the internal automatic programming cycle will commence.

### DATA Polling

The X2864A features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864A, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

## WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

## ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

3

## X2864A, X2864AI

### SYSTEM CONSIDERATIONS

Because the X2864A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.






To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864A has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

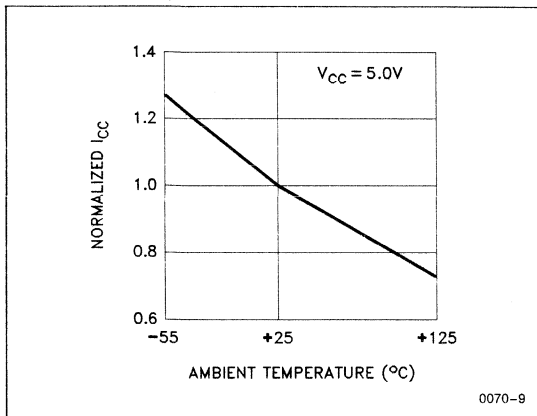
In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

### SYMBOL TABLE

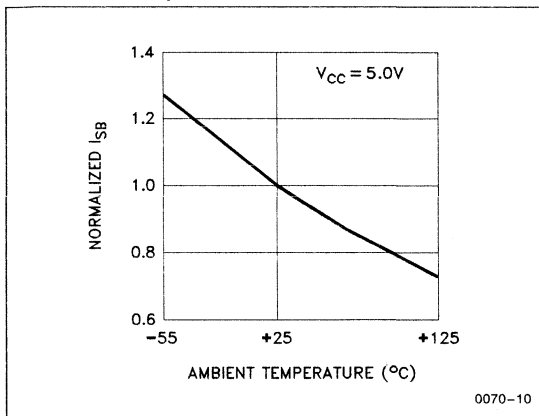
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X2864A, X2864AI

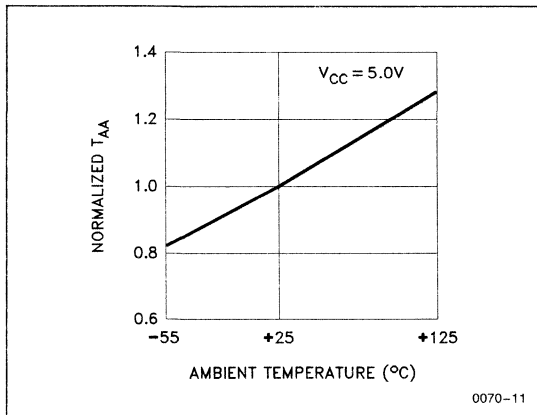
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



3

---

## NOTES

**Electrically Erasable PROM**

**FEATURES**

- **250 ns Access Time**
- **Fast Write Cycle Times**
  - 16-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 2.6 Sec. Typical
  - Effective Byte Write Cycle Time of 300  $\mu$ s Typical
- **DATA Polling**
  - Allows User to Minimize Write Cycle Time
- **Simple Byte and Page Write**
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **JEDEC Approved Byte-Wide Pinout**

**DESCRIPTION**

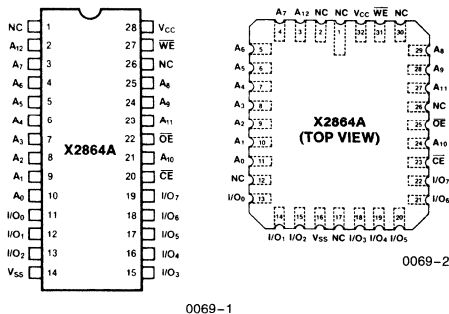
The Xicor X2864A is a 8K x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2864A features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2864A supports a 16-byte page write operation, effectively providing a 300  $\mu$ s/byte write and enabling the entire memory to be written in less than 2.6 seconds. The X2864A also features DATA Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.



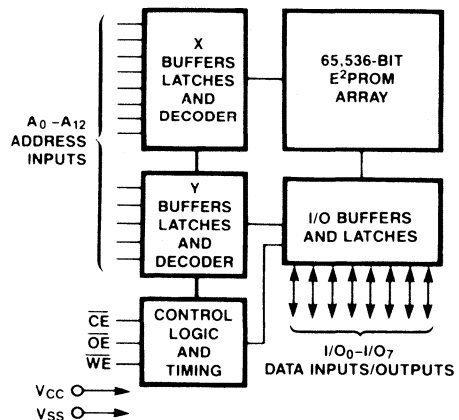
**PIN CONFIGURATIONS**



**PIN NAMES**

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

**FUNCTIONAL DIAGRAM**



0069-3

# X2864AM

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	.....	-65°C to +135°C
Storage Temperature	.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground	.....	-1.0V to +7V
D.C. Output Current	.....	5 mA
Lead Temperature (Soldering, 10 Seconds)	.....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		140	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		70	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.0	$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage		0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0 \text{ MHz}$ , $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.  
 (2) This parameter is periodically sampled and not 100% tested.

# X2864AM

## A.C. CHARACTERISTICS

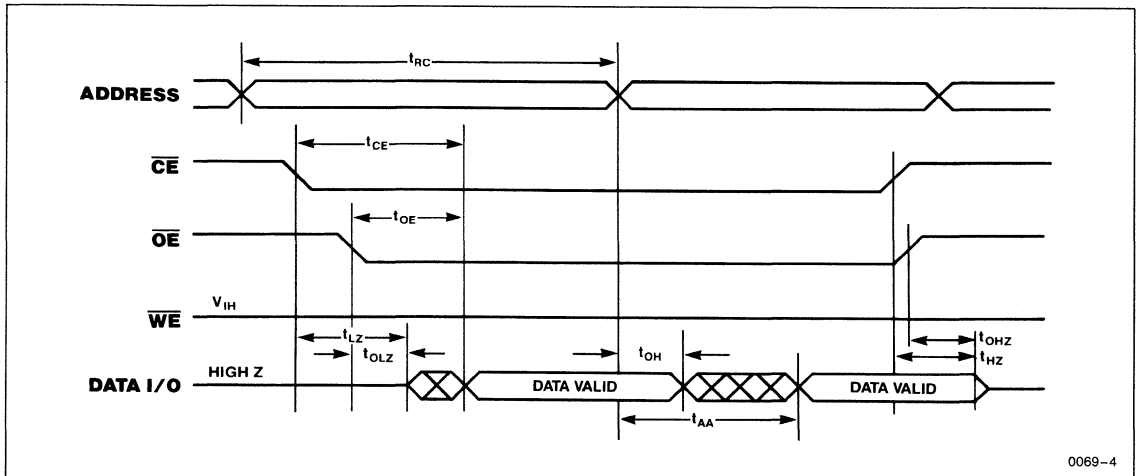
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2864AM-25		X2864AM		X2864AM-35		X2864AM-45		Units
		Min.	Max.	Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		450		ns
$t_{CE}$	Chip Enable Access Time		250		300		350		450	ns
$t_{AA}$	Address Access Time		250		300		350		450	ns
$t_{OE}$	Output Enable Access Time		150		150		150		150	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		10		10		ns
$t_{HZ}^{(3)}$	Chip Disable to Output in High Z	10	60	10	80	10	80	10	100	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		10		10		ns
$t_{OHZ}^{(3)}$	Output Disable to Output in High Z	10	60	10	80	10	80	10	100	ns
$t_{OH}$	Output Hold from Address Change	10		10		10		10		ns

3

### Read Cycle



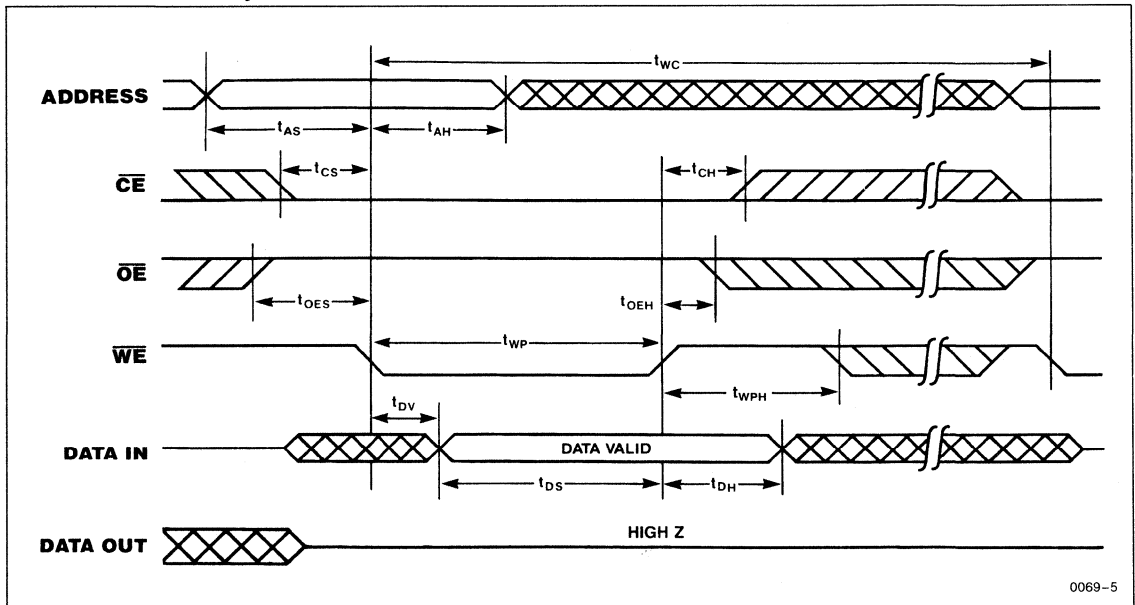
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864AM

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time	10		ms
$t_{AS}$	Address Setup Time	10		ns
$t_{AH}$	Address Hold Time	200		ns
$t_{CS}$	Write Setup Time	0		ns
$t_{CH}$	Write Hold Time	0		ns
$t_{CW}$	$\overline{CE}$ Pulse Width	150		ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10		ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10		ns
$t_{WP}$	$\overline{WE}$ Pulse Width	150		ns
$t_{WPH}$	$\overline{WE}$ High Recovery	50		ns
$t_{DV}$	Data Valid		300	ns
$t_{DS}$	Data Setup	100		ns
$t_{DH}$	Data Hold	20		ns
$t_{DW}$	Delay to Next Write	500		$\mu$ S
$t_{BLC}$	Byte Load Cycle	3	20	$\mu$ S

## $\overline{WE}$ Controlled Write Cycle

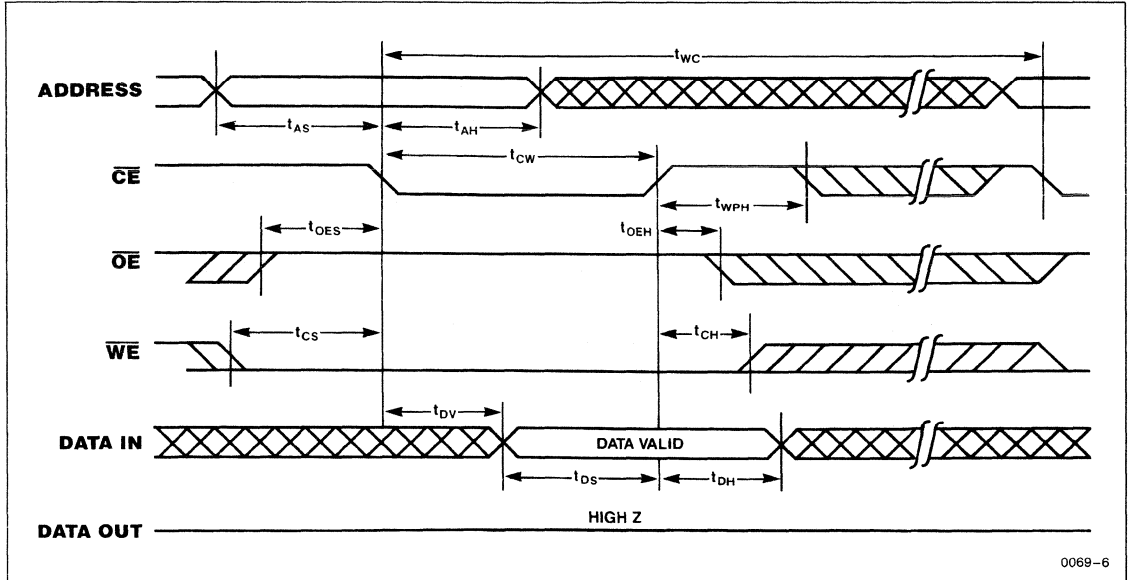


0069-5



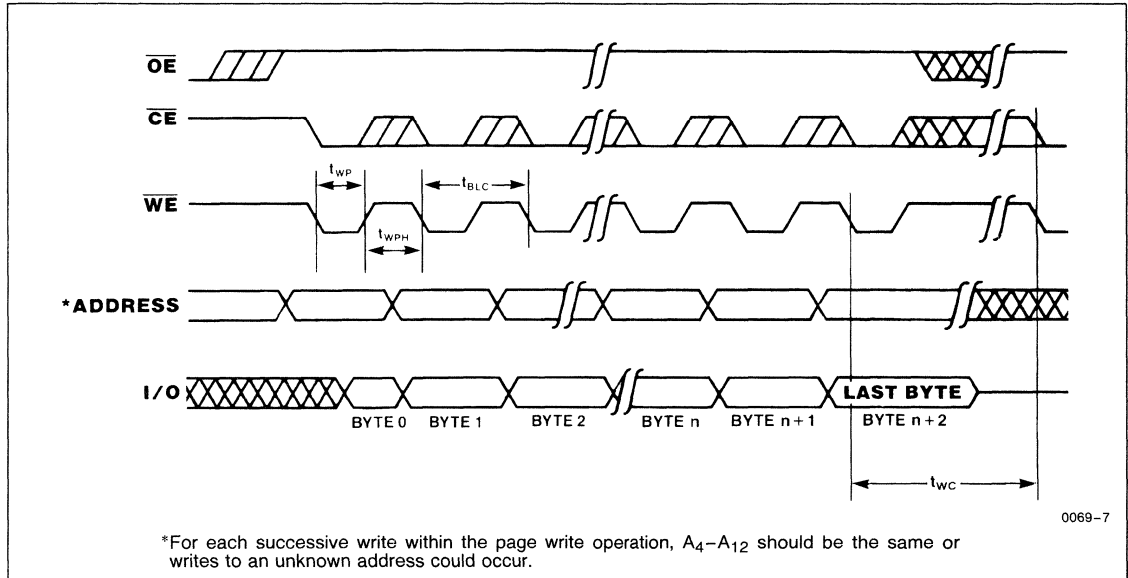
# X2864AM

## $\overline{CE}$ Controlled Write Cycle



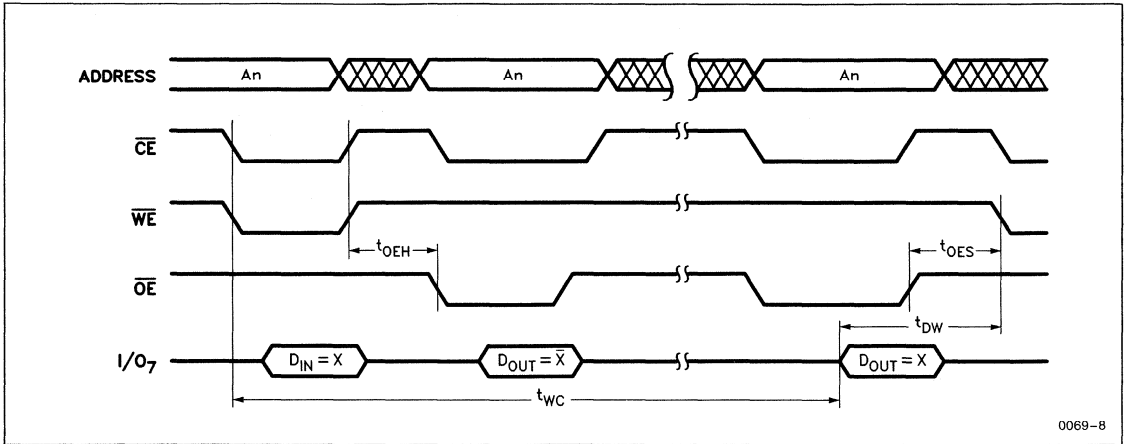
3

## Page Mode Write Cycle



# X2864AM

## DATA Polling Timing Diagram



# X2864AM

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{12}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2864A through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864A.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

The page write feature of the X2864A allows the entire memory to be written in 2.6 seconds. Page write allows two to sixteen bytes of data to be consecutively written to the X2864A prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is,  $A_4$  through  $A_{12}$  must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to fifteen bytes in the same manner as the first byte was written. Each successive byte write cycle must begin within 20  $\mu$ s of the falling edge of  $\overline{WE}$  of the preceding cycle. If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 20  $\mu$ s the internal automatic programming cycle will commence.

### DATA Polling

The X2864A features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864A, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

## WRITE PROTECTION

There are three features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

## ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

3

# X2864AM

## SYSTEM CONSIDERATIONS

Because the X2864A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

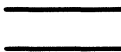




To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864A has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

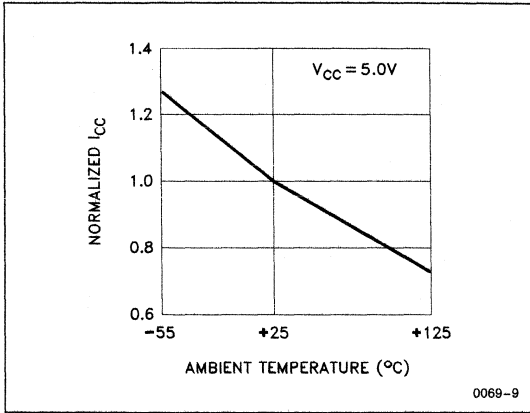
In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

## SYMBOL TABLE

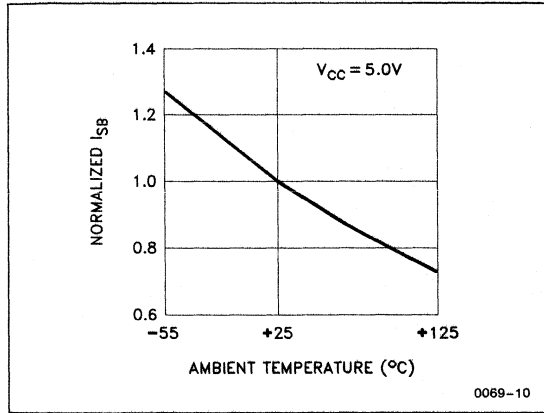
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

# X2864AM

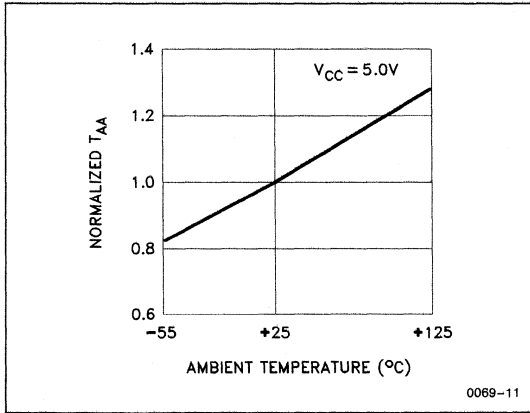
**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**Normalized Access Time vs. Ambient Temperature**



3

---

## NOTES

64K

Mil-Std-883C

X2864AMB

8192 x 8 Bit

## Electrically Erasable PROM

### A.C. AND D.C. REQUIREMENTS FOR CHIP ERASE

CHIP ERASE FUNCTIONALITY WILL BE GUARANTEED VIA C-SPEC ONLY. ADD C6600 TO XICOR PART NUMBER WHEN ORDERING.

The X2864AMB provides a mode of operation that erases the entire contents of the memory in one write cycle. This mode is entered by raising  $\overline{OE}$  to between +18V and +22V, placing all I/Os at  $V_{IH}$  and performing a standard write operation. The erasure will be completed in 10 ms.

With the exception of  $V_{OE}$ , all device A.C. and D.C. parameters are the same as those for normal operation.

*The chip erase operation is only guaranteed on Mil-Std-883C product.*

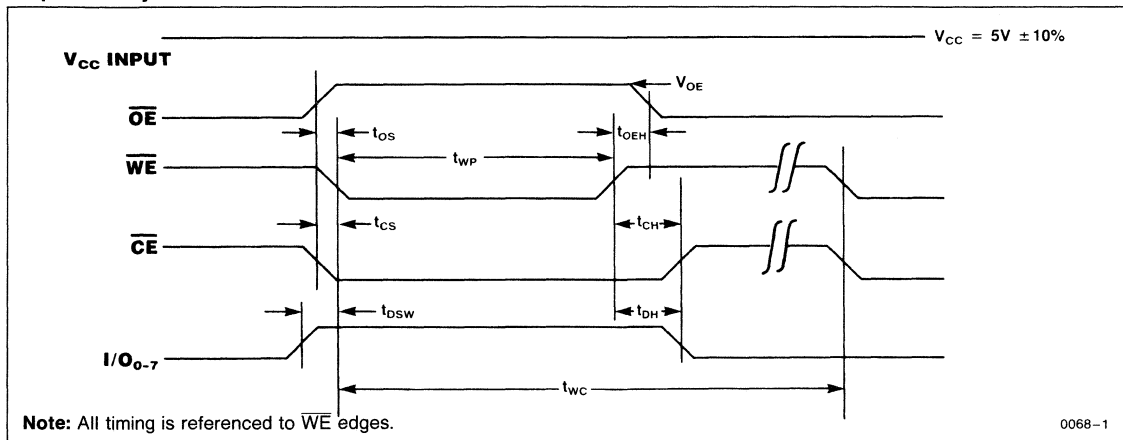
### A.C. CHIP ERASE CHARACTERISTICS

Symbol	Parameter	Limits		Units
		Min.	Max.	
$t_{CS}$	$\overline{CE}$ to $\overline{WE}$ Setup Time	10		ns
$t_{DSW}$	Data to $\overline{WE}$ Setup Time	10		ns
$t_{DH}$	Data Hold Time	50		ns
$t_{WP}$	Write Pulse Width	175		ns
$t_{CH}$	$\overline{CE}$ Hold Time	50		ns
$t_{OS}$	$V_{OE}$ Setup Time	10		ns
$t_{OEH}$	$V_{OE}$ Hold Time	10		ns
$t_{WC}$	Write Cycle Time		10	ms

### D.C. CHARACTERISTIC FOR $V_{OE}$

Symbol	Parameter	Limits		Units	Note
		Min.	Max.		
$V_{OE}$	$\overline{OE}$ Chip Erase Voltage	+18	+22	V	$I_{OE} = 10 \mu A$

### Chip Erase Cycle



3

---

## NOTES



Electrically Erasable PROM

FEATURES

- 350 ns Access Time
- Fast Write Cycle Times
  - 16-Byte Page Write Operation
  - Byte or Page Write Cycle: 10 ms Typical
  - Complete Memory Rewrite: 5.2 Sec. Typical
  - Effective Byte Write Cycle Time of 600  $\mu$ s Typical
- DATA Polling
  - Allows User to Minimize Write Cycle Time
- Simple Byte and Page Write
  - Single TTL Level WE Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- JEDEC Approved Byte-Wide Pinout

DESCRIPTION

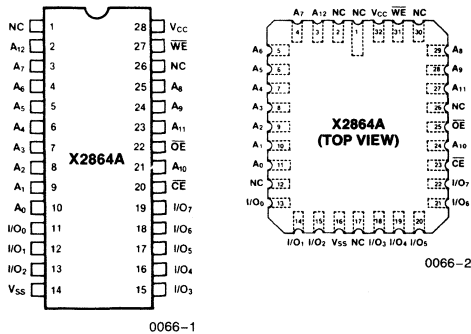
The Xicor X2864A is a 8K x 8 E<sup>2</sup>PROM, fabricated with the same reliable N-channel floating gate MOS technology used in all Xicor 5V programmable nonvolatile memories. The X2864A features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2864A supports a 16-byte page write operation, effectively providing a 600  $\mu$ s/byte write and enabling the entire memory to be written in less than 5.2 seconds. The X2864A also features  $\overline{\text{DATA}}$  Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Refer to Device Operation for further endurance information. Data retention is specified to be greater than 100 years.



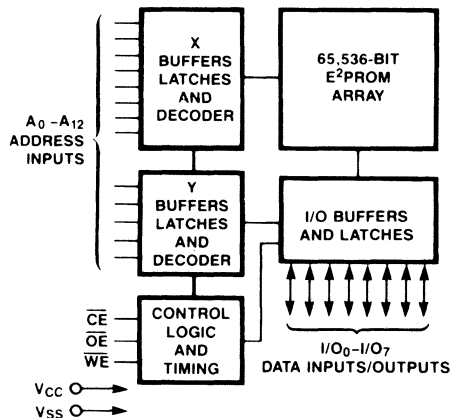
PIN CONFIGURATIONS



PIN NAMES

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
WE	Write Enable
CE	Chip Enable
OE	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

FUNCTIONAL DIAGRAM



0066-3

# X2864AT

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias .....	-10°C to +160°C
Storage Temperature .....	-65°C to +160°C
Voltage on any Pin with Respect to Ground .....	-1.0V to +7V
D.C. Output Current .....	5 mA
Lead Temperature (Soldering, 10 Seconds) .....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = 0^\circ\text{C}$  to  $+150^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits		Units	Test Conditions
		Min.	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		110	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current		10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current		10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0	0.8	V	
$V_{IH}$	Input High Voltage	2.4	$V_{CC} + 0.5$	V	
$V_{OL}$	Output Low Voltage		0.5	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4		V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2864AT

## A.C. CHARACTERISTICS

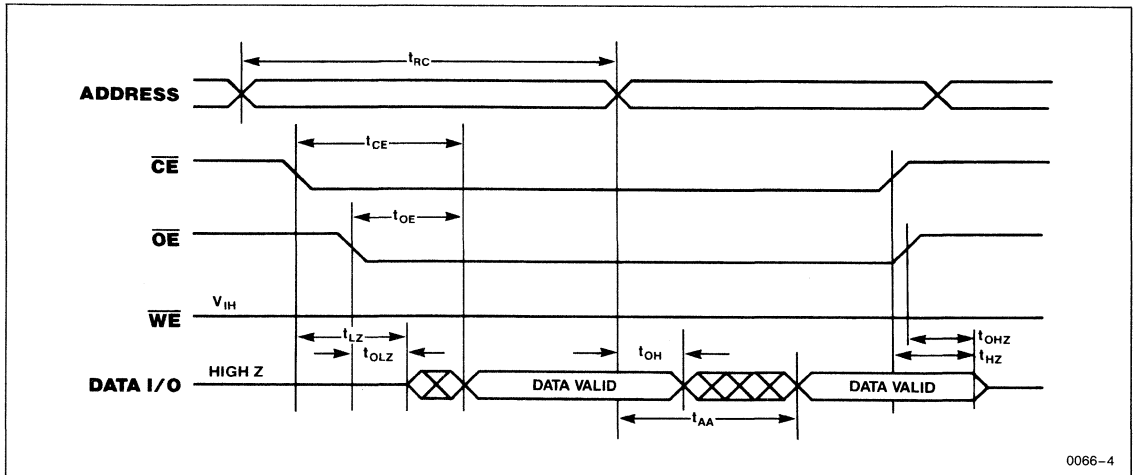
$T_A = 0^\circ\text{C to } +150^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2864AT-35		X2864AT-45		Units
		Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	350		450		ns
$t_{CE}$	Chip Enable Access Time		350		450	ns
$t_{AA}$	Address Access Time		350		450	ns
$t_{OE}$	Output Enable Access Time		100		100	ns
$t_{LZ}$	Chip Enable to Output in Low Z	10		10		ns
$t_{HZ}^{(3)}$	Chip Disable to Output in High Z	10	150	10	150	ns
$t_{OLZ}$	Output Enable to Output in Low Z	10		10		ns
$t_{OHZ}^{(3)}$	Output Disable to Output in High Z	10	150	10	150	ns
$t_{OH}$	Output Hold from Address Change	10		10		ns

3

### Read Cycle



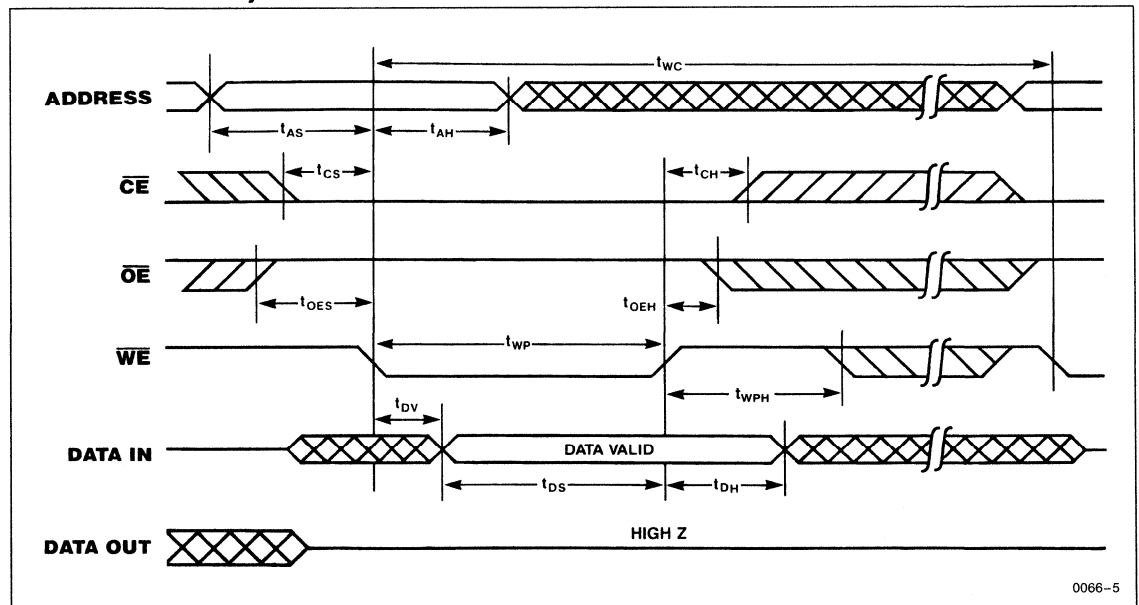
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864AT

## Write Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time		20	ms
$t_{AS}$	Address Setup Time	20		ns
$t_{AH}$	Address Hold Time	250		ns
$t_{CS}$	Write Setup Time	0		ns
$t_{CH}$	Write Hold Time	0		ns
$t_{CW}$	$\overline{CE}$ Pulse Width	200		ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10		ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10		ns
$t_{WP}$	$\overline{WE}$ Pulse Width	200		ns
$t_{WPH}$	$\overline{WE}$ High Recovery	100		ns
$t_{DV}$	Data Valid		300	ns
$t_{DS}$	Data Setup	200		ns
$t_{DH}$	Data Hold	20		ns
$t_{DW}$	Delay to Next Write	500		$\mu$ s
$t_{BLC}$	Byte Load Cycle	3	40	$\mu$ s

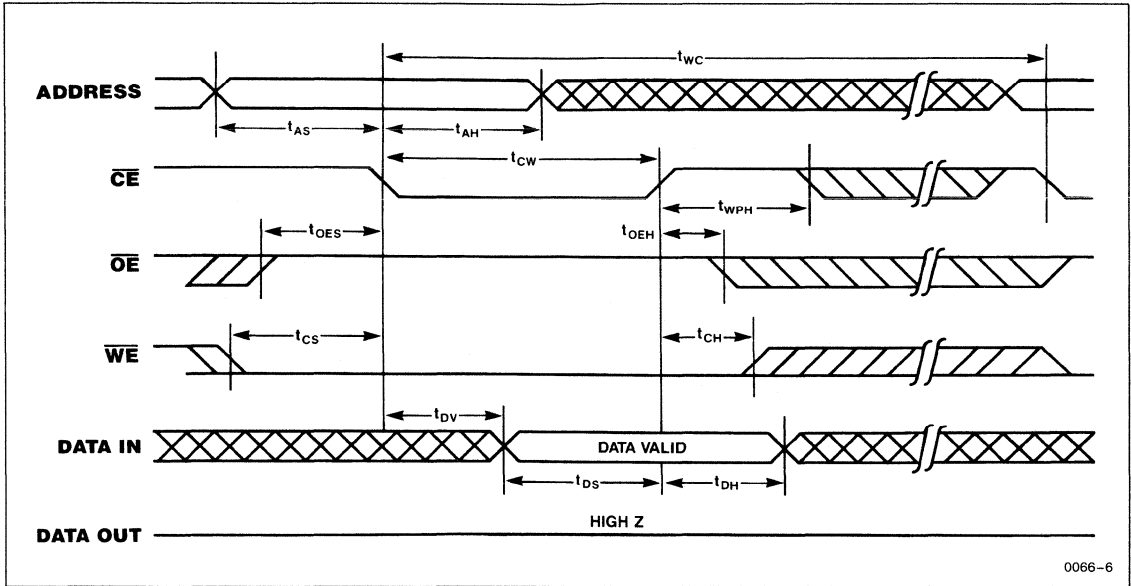
## $\overline{WE}$ Controlled Write Cycle



0066-5

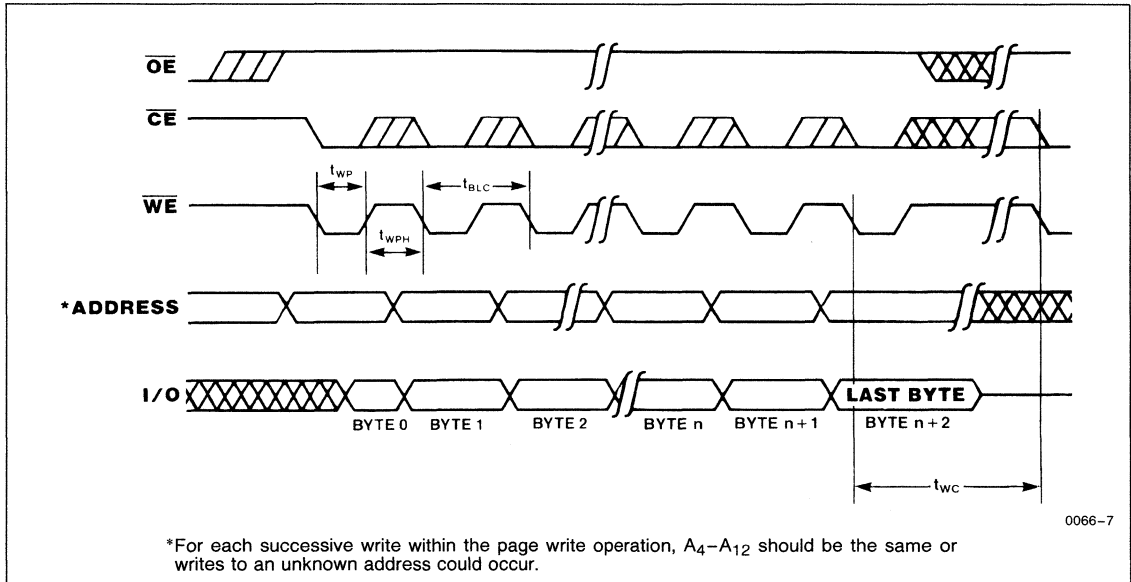
# X2864AT

## $\overline{\text{CE}}$ Controlled Write Cycle



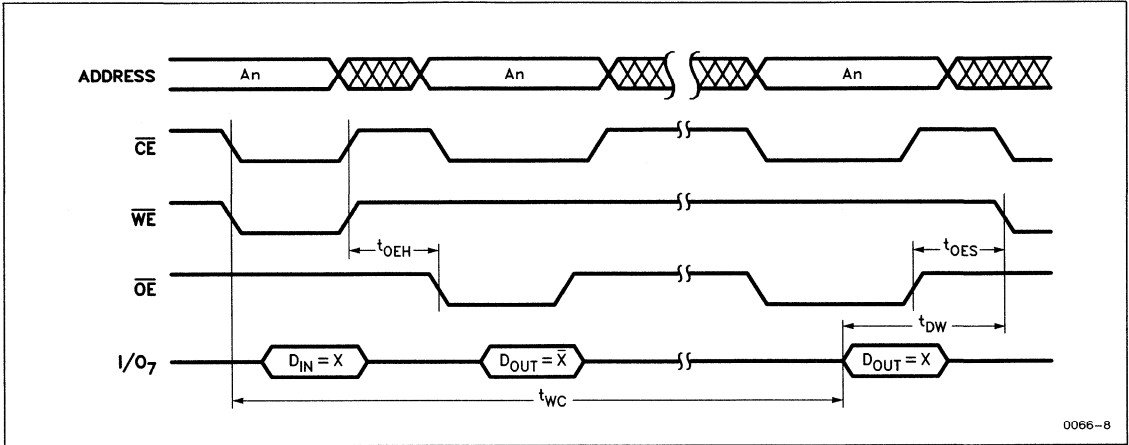
3

## Page Mode Write Cycle



# X2864AT

## DATA Polling Timing Diagram



## X2864AT

### PIN DESCRIPTIONS

#### Addresses ( $A_0$ – $A_{12}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

#### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

#### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

#### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2864A through the I/O pins.

#### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864A.

### DEVICE OPERATION

#### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

#### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864A supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 10 ms.

#### Page Write Operation

The page write feature of the X2864A allows the entire memory to be written in 5.2 seconds. Page write allows two to sixteen bytes of data to be consecutively written

to the X2864A prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is,  $A_4$  through  $A_{12}$  must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to fifteen bytes in the same manner as the first byte was written. Each successive byte write cycle must begin within 20  $\mu$ s of the falling edge of  $\overline{WE}$  of the preceding cycle. If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 20  $\mu$ s the internal automatic programming cycle will commence.

#### $\overline{DATA}$ Polling

The X2864A features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864A, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

#### WRITE PROTECTION

There are two features that protect the nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse of less than 20 ns will not initiate a write cycle.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

#### ENDURANCE

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. The process average for endurance of Xicor E<sup>2</sup>PROMs is documented in RR504, the *Xicor Reliability Report on Endurance*. Included in that report is a method for determining the expected endurance of the device based upon the specific application environment. RR504 and additional reliability reports are available from Xicor.

## X2864AT

### SYSTEM CONSIDERATIONS

Because the X2864A is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.






To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864A has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

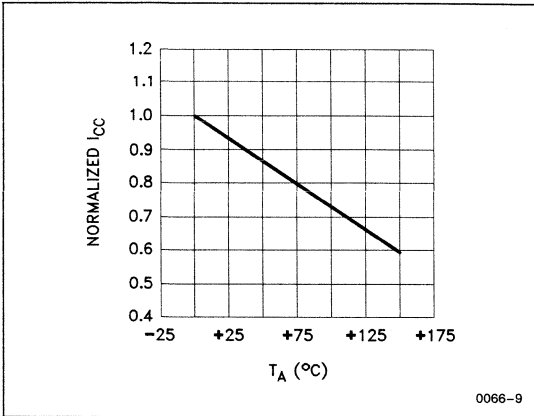
### SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

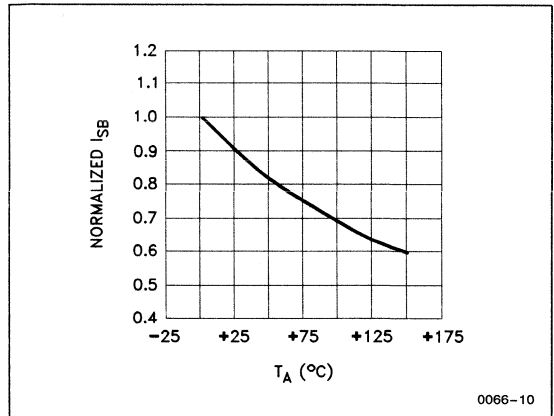


# X2864AT

**Normalized Active Supply Current  
vs. Ambient Temperature**



**Normalized Standby Supply Current  
vs. Ambient Temperature**



3

---

## NOTES

## Electrically Erasable PROM

### TYPICAL FEATURES

- **120 ns Access Time**
- **High Performance Scaled NMOS Technology**
- **Fast Write Cycle Times**
  - 32-Byte Page Write Operation
  - Byte or Page Write Cycle: 3 ms Typical
  - Complete Memory Rewrite: 750 ms Typical
  - Effective Byte Write Cycle Time of 95  $\mu$ s Typical
- **DATA Polling**
  - Allows User to Minimize Write Cycle Time
- **Simple Byte and Page Write**
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **JEDEC Approved Byte-Wide Pinout**

### DESCRIPTION

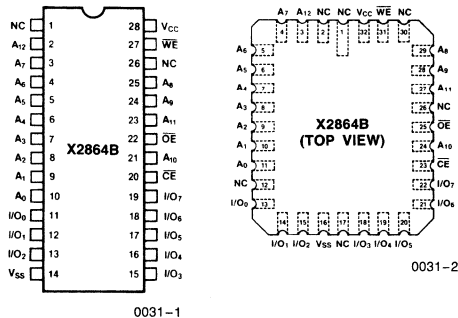
The Xicor X2864B is a 8K x 8 E<sup>2</sup>PROM, fabricated with an advanced, high performance N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories it is a 5V only device. The X2864B features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2864B supports a 32-byte page write operation, effectively providing a 95  $\mu$ s/byte write cycle and enabling the entire memory to be written in less than 750 ms. The X2864B also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

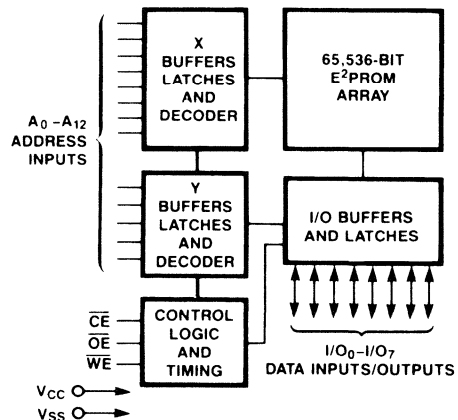
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0031-3

# X2864B, X2864BI

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2864B	-10°C to +85°C
X2864BI	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2864B  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

X2864BI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80	150	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		50	80	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0V$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0.4V to 2.4V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	0.8V and 2.0V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2864B, X2864BI

## A.C. CHARACTERISTICS

X2864B  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

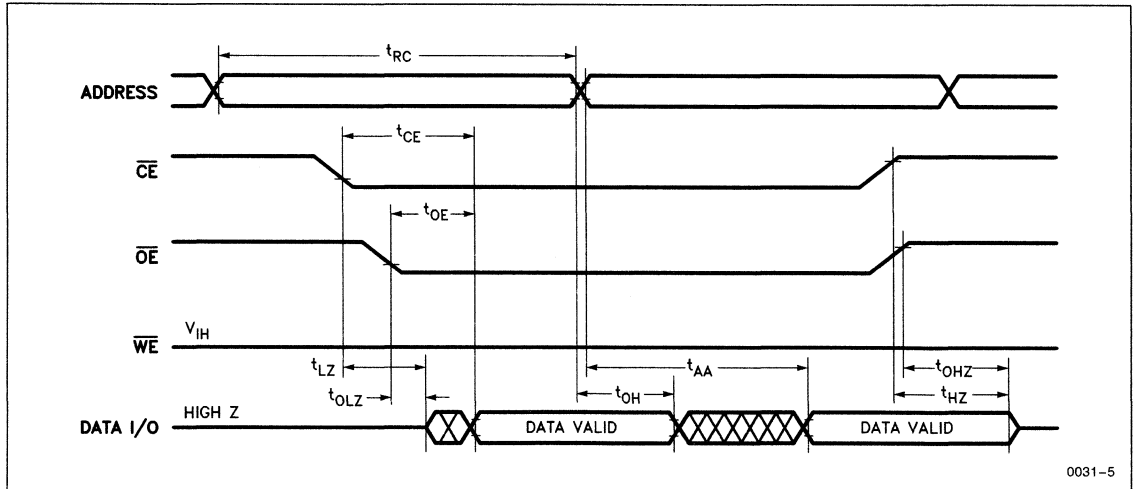
X2864BI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2864B-12 X2864BI-12		X2864B-15 X2864BI-15		X2864B-18 X2864BI-18		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	120		150		180		ns
$t_{CE}$	Chip Enable Access Time		120		150		180	ns
$t_{AA}$	Address Access Time		120		150		180	ns
$t_{OE}$	Output Enable Access Time		50		70		100	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

3

### Read Cycle



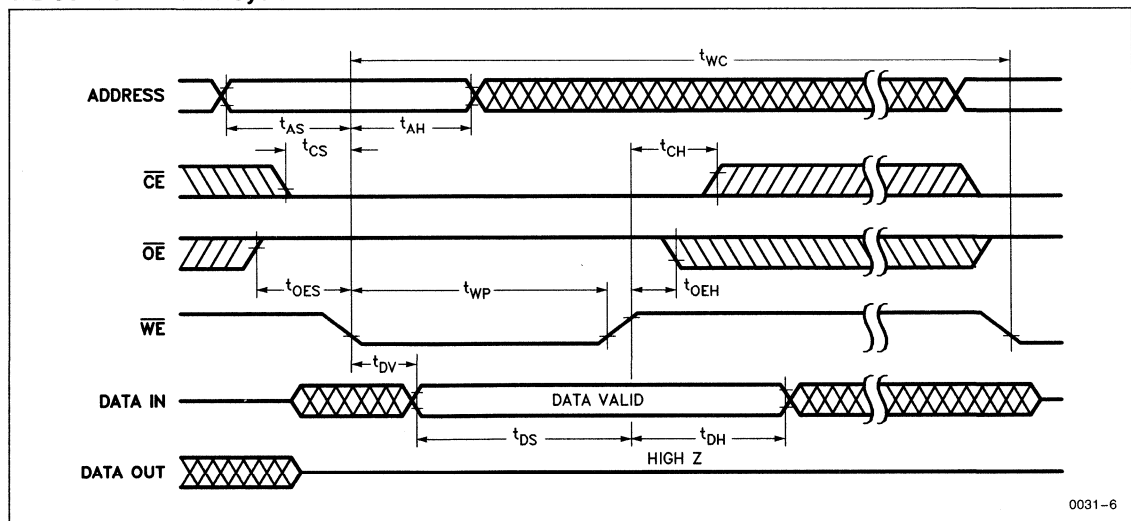
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864B, X2864BI

## Write Cycle Limits

Symbol	Parameter	Min.	Typ. <sup>(4)</sup>	Max.	Units
$t_{WC}$	Write Cycle Time		3	5	ms
$t_{AS}$	Address Setup Time	5			ns
$t_{AH}$	Address Hold Time	50			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	100			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	100			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	500			ns
$t_{DV}$	Data Valid			100	$\mu$ s
$t_{DS}$	Data Setup	50			ns
$t_{DH}$	Data Hold	5			ns
$t_{DW}$	Delay to Next Write	10			$\mu$ s
$t_{BLC}$	Byte Load Cycle	1		100	$\mu$ s

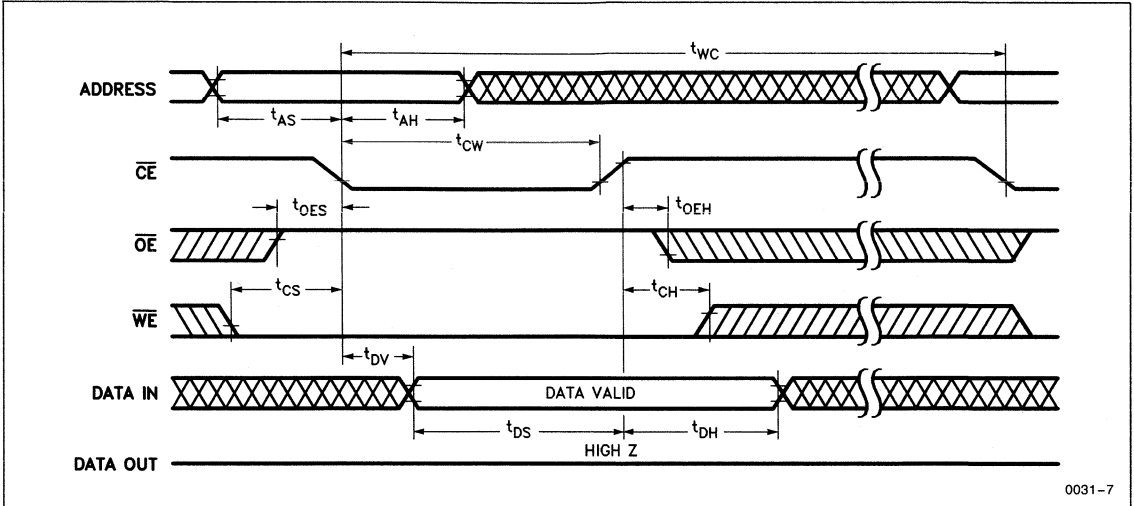
## $\overline{WE}$ Controlled Write Cycle



**Note:** (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

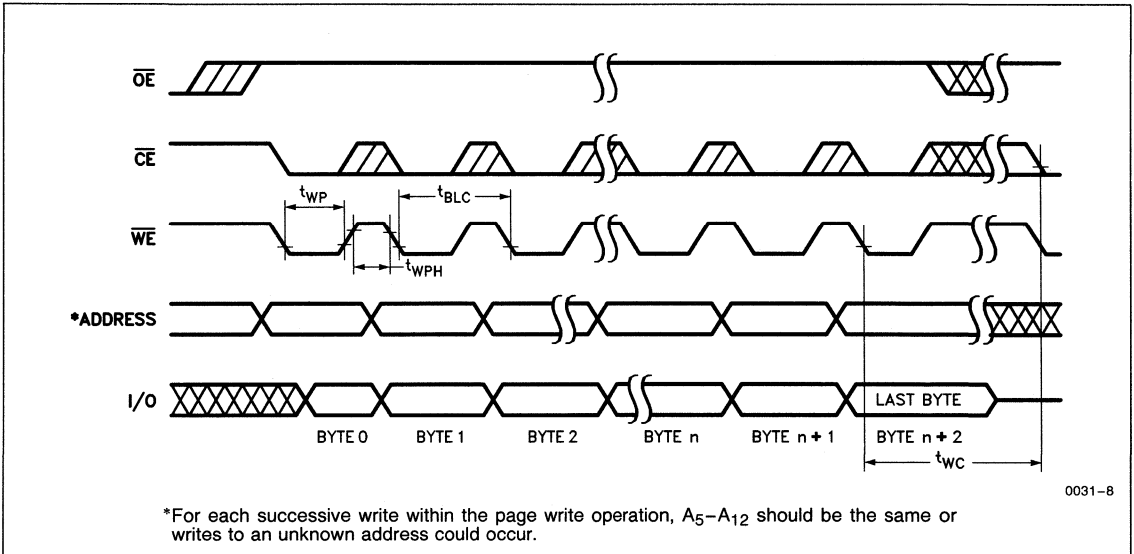
# X2864B, X2864BI

## $\overline{\text{CE}}$ Controlled Write Cycle



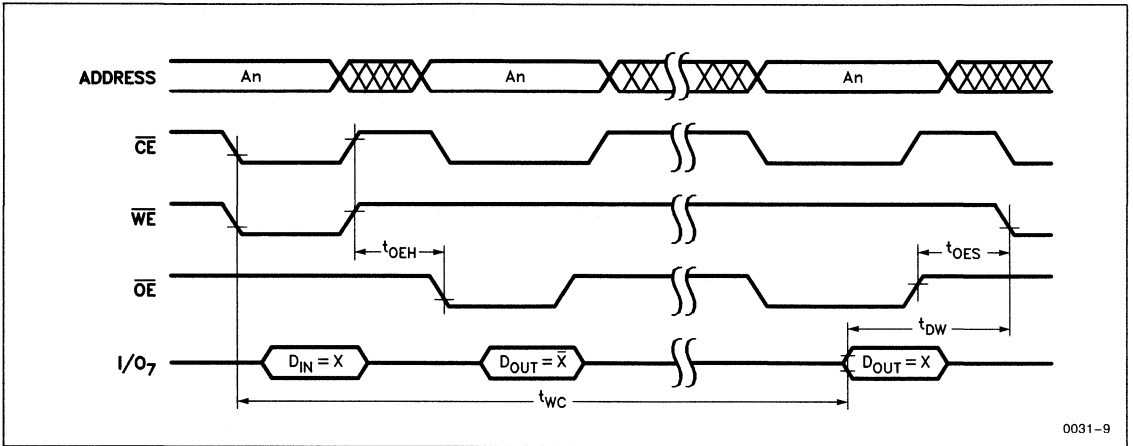
3

## Page Mode Write Cycle



# X2864B, X2864BI

## DATA Polling Timing Diagram





## X2864B, X2864BI

### PIN DESCRIPTIONS

#### Addresses (A<sub>0</sub>–A<sub>12</sub>)

The Address inputs select an 8-bit memory location during a read or write operation.

#### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

#### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

#### Data In/Data Out (I/O<sub>0</sub>–I/O<sub>7</sub>)

Data is written to or read from the X2864B through the I/O pins.

#### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864B.

### DEVICE OPERATION

#### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

#### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864B supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 3 ms.

#### Page Write Operation

The page write feature of the X2864B allows the entire memory to be written in 750 ms. Page write allows two

to thirty-two bytes of data to be consecutively written to the X2864B prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is, A<sub>5</sub> through A<sub>12</sub> must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to thirty-one bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s the internal automatic programming cycle will commence. There is no page write window limitation. The page write window is infinitely wide so long as the host continues to access the device within the byte load cycle time of 100  $\mu$ s.

#### DATA Polling

The X2864B features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864B, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on I/O<sub>7</sub> (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete, I/O<sub>7</sub> will reflect true data.

#### WRITE PROTECTION

There are two features that protect the nonvolatile data from inadvertent writes.

- V<sub>CC</sub> Sense—All functions are inhibited when V<sub>CC</sub> is  $\leq 3.5$ V.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

## X2864B, X2864BI

### SYSTEM CONSIDERATIONS

Because the X2864B is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.






To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864B has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

### SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

**Electrically Erasable PROM**

**TYPICAL FEATURES**

- **120 ns Access Time**
- **High Performance Scaled NMOS Technology**
- **Fast Write Cycle Times**
  - 32-Byte Page Write Operation
  - Byte or Page Write Cycle: 3 ms Typical
  - Complete Memory Rewrite: 750 ms Typical
  - Effective Byte Write Cycle Time of 95  $\mu$ s Typical
- **DATA Polling**
  - Allows User to Minimize Write Cycle Time
- **Simple Byte and Page Write**
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **JEDEC Approved Byte-Wide Pinout**

**DESCRIPTION**

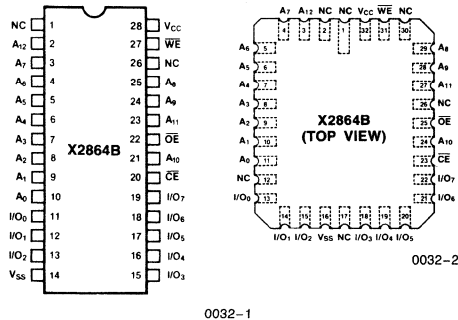
The Xicor X2864B is an 8K x 8 E<sup>2</sup>PROM, fabricated with an advanced, high performance N-channel floating gate MOS technology. Like all Xicor programmable memories it is a 5V only device. The X2864B features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2864B supports a 32-byte page write operation, effectively providing a 95  $\mu$ s/byte write cycle and enabling the entire memory to be written in less than 750 ms. The X2864B also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.



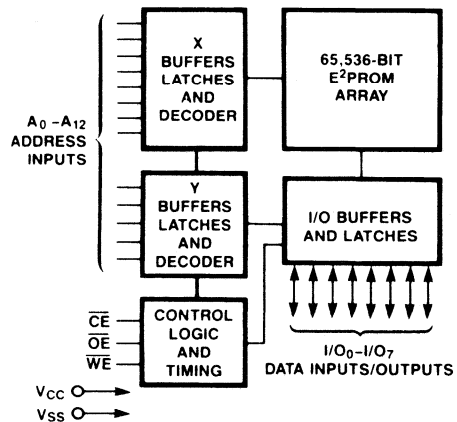
**PIN CONFIGURATIONS**



**PIN NAMES**

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

**FUNCTIONAL DIAGRAM**



0032-3

# X2864BM

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	.....	-65°C to +135°C
Storage Temperature	.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground	.....	-1.0V to +7V
D.C. Output Current	.....	5 mA
Lead Temperature (Soldering, 10 Seconds)	.....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80	150	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		50	80	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

## CAPACITANCE $T_A = 25^\circ\text{C}$ , $f = 1.0 \text{ MHz}$ , $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0V$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0.4V to 2.4V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	0.8V and 2.0V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

Notes: (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2864BM

## A.C. CHARACTERISTICS

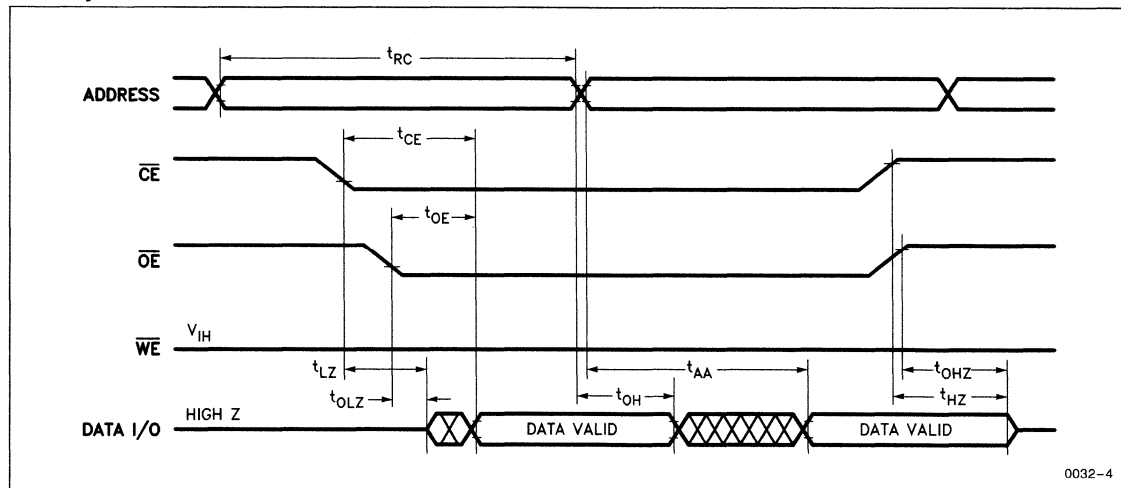
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2864BM-12		X2864BM-15		X2864BM-18		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	120		150		180		ns
$t_{CE}$	Chip Enable Access Time		120		150		180	ns
$t_{AA}$	Address Access Time		120		150		180	ns
$t_{OE}$	Output Enable Access Time		50		70		100	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

3

### Read Cycle



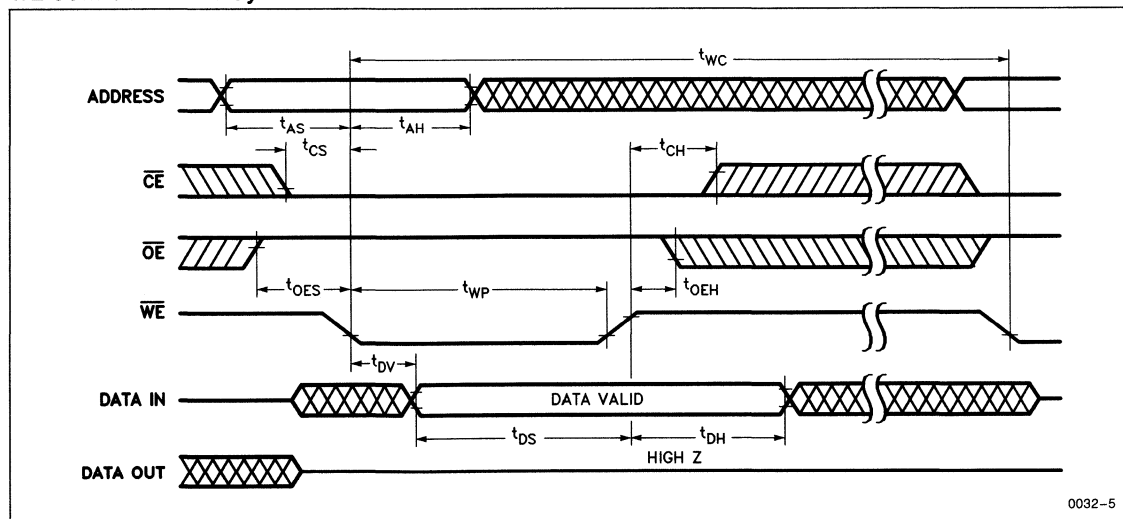
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864BM

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		3	5	ms
$t_{AS}$	Address Setup Time	5			ns
$t_{AH}$	Address Hold Time	50			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	100			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	100			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	500			ns
$t_{DV}$	Data Valid			100	$\mu$ s
$t_{DS}$	Data Setup	50			ns
$t_{DH}$	Data Hold	5			ns
$t_{DW}$	Delay to Next Write	10			$\mu$ s
$t_{BLC}$	Byte Load Cycle	1		100	$\mu$ s

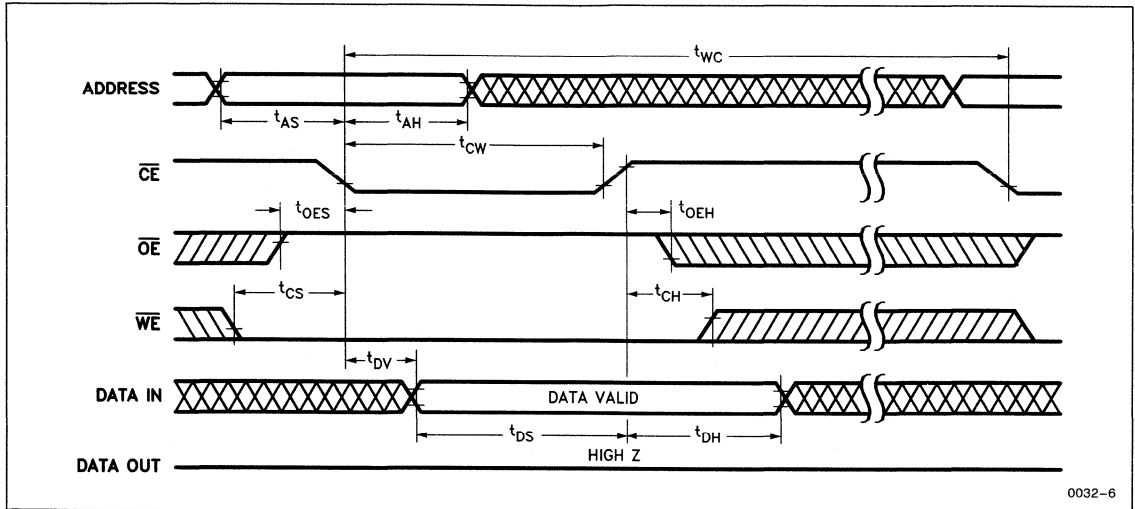
## $\overline{WE}$ Controlled Write Cycle



Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

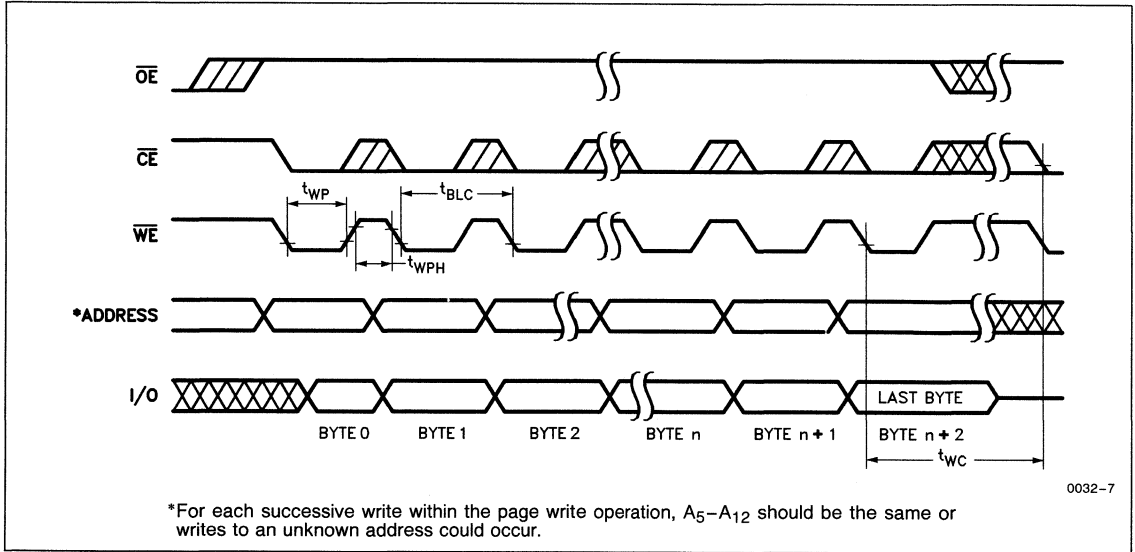
# X2864BM

## CE Controlled Write Cycle



3

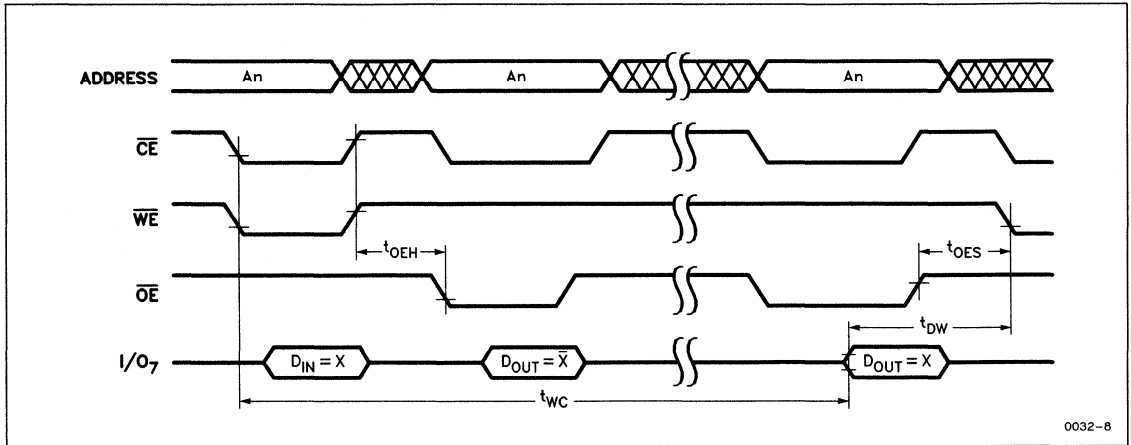
## Page Mode Write Cycle



\*For each successive write within the page write operation,  $A_5-A_{12}$  should be the same or writes to an unknown address could occur.

# X2864BM

## DATA Polling Timing Diagram





# X2864BM

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{12}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2864B through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864B.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864B supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 3 ms.

### Page Write Operation

The page write feature of the X2864B allows the entire memory to be written in 750 ms. Page write allows two

to thirty-two bytes of data to be consecutively written to the X2864B prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is,  $A_5$  through  $A_{12}$  must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to thirty-one bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. The page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 100  $\mu$ s.

### DATA Polling

The X2864B features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864B, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

### WRITE PROTECTION

There are two features that protect the nonvolatile data from inadvertent writes.

- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3.5V$ .
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

3

# X2864BM

## SYSTEM CONSIDERATIONS

Because the X2864B is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.






To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864B has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

**64K Commercial X2864H 8192 x 8 Bit**  
**Industrial X2864HI**

## Electrically Erasable PROM

### TYPICAL FEATURES

- 70 ns Access Time
- High Performance Scaled NMOS Technology
- Fast Write Cycle Times
  - 32-Byte Page Write Operation
  - Byte or Page Write Cycle: 3 ms Typical
  - Complete Memory Rewrite: 750 ms Typical
  - Effective Byte Write Cycle Time of 95  $\mu$ s Typical
- DATA Polling
  - Allows User to Minimize Write Cycle Time
- Simple Byte and Page Write
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- JEDEC Approved Byte-Wide Pinout

### DESCRIPTION

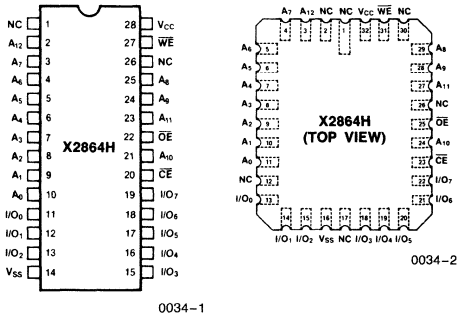
The Xicor X2864H is a high speed 8K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories it is a 5V only device. The X2864H features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs, and EPROMs.

The X2864H supports a 32-byte page write operation, effectively providing a 95  $\mu$ s/byte write cycle and enabling the entire memory to be written in less than 750 ms. The X2864H also features DATA Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

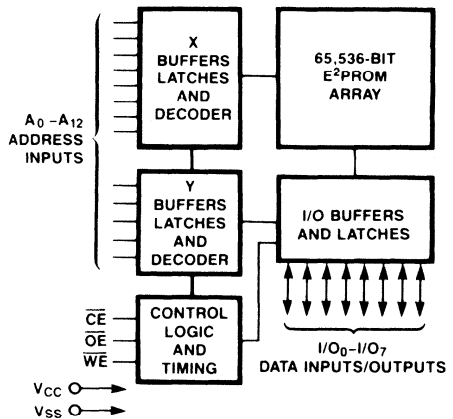
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
OE	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0034-3

# X2864H, X2864HI

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X2864H	-10°C to +85°C
X2864HI	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X2864H  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

X2864HI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80	150	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		50	80	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0V$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0.4V to 2.4V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	0.8V and 2.0V
Output Load	1 TTL Gate and $C_L = 30 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2864H, X2864HI

## A.C. CHARACTERISTICS

X2864H  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

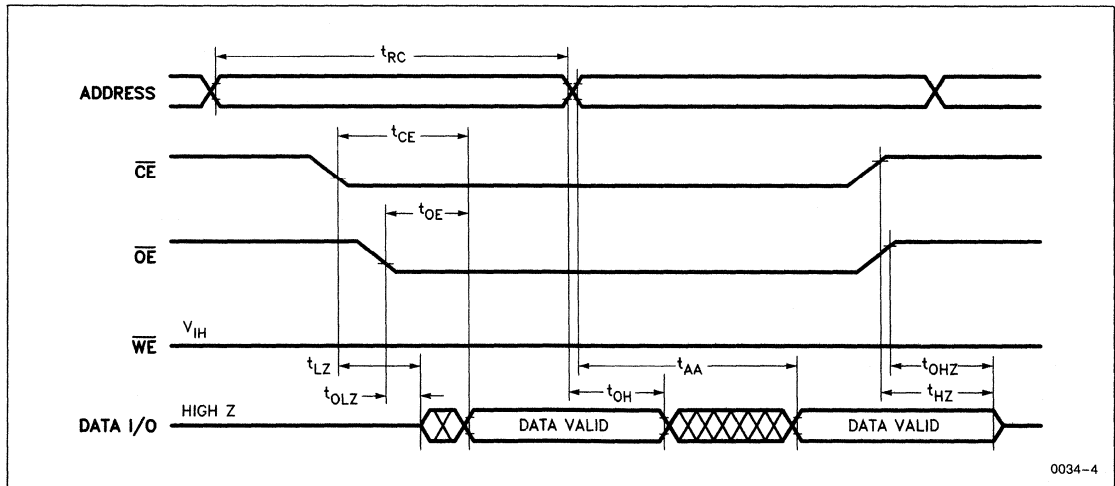
X2864HI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X2864H-70 X2864HI-70		X2864H-90 X2864HI-90		Units
		Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	70		90		ns
$t_{CE}$	Chip Enable Access Time		70		90	ns
$t_{AA}$	Address Access Time		70		90	ns
$t_{OE}$	Output Enable Access Time		35		45	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	40	0	40	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	40	0	40	ns
$t_{OH}$	Output Hold from Address Change	0		0		ns

3

### Read Cycle



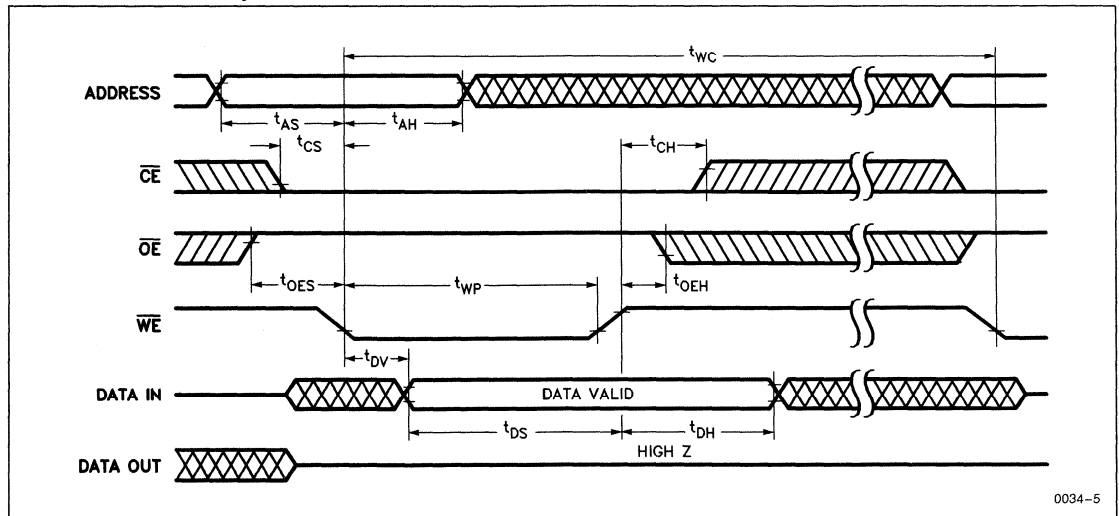
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864H, X2864HI

## Write Cycle Limits

Symbol	Parameter	X2864H-70 X2864HI-70		X2864H-90 X2864HI-90		Units
		Min.	Max.	Min.	Max.	
$t_{WC}$	Write Cycle Time		5		5	ms
$t_{AS}$	Address Setup Time	5		5		ns
$t_{AH}$	Address Hold Time	50		50		ns
$t_{CS}$	Write Setup Time	0		0		ns
$t_{CH}$	Write Hold Time	0		0		ns
$t_{CW}$	$\overline{CE}$ Pulse Width	60		80		ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10		10		ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	5		5		ns
$t_{WP}$	$\overline{WE}$ Pulse Width	60		80		ns
$t_{WPH}$	$\overline{WE}$ High Recovery	500		500		ns
$t_{DV}$	Data Valid		100		100	$\mu$ s
$t_{DS}$	Data Setup	35		35		ns
$t_{DH}$	Data Hold	5		5		ns
$t_{DW}$	Delay to Next Write	10		10		$\mu$ s
$t_{BLC}$	Byte Load Cycle	1	100	1	100	$\mu$ s

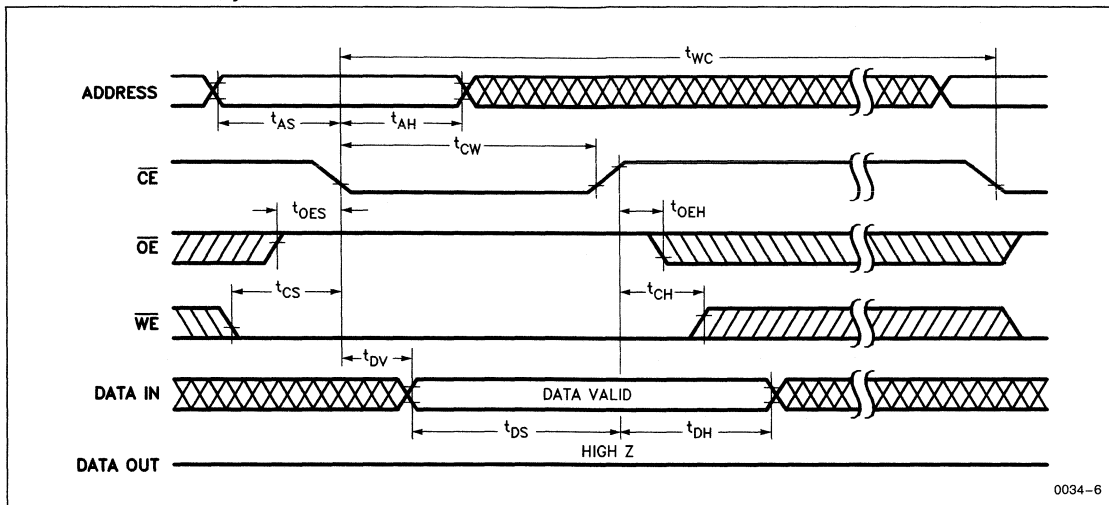
## $\overline{WE}$ Controlled Write Cycle



0034-5

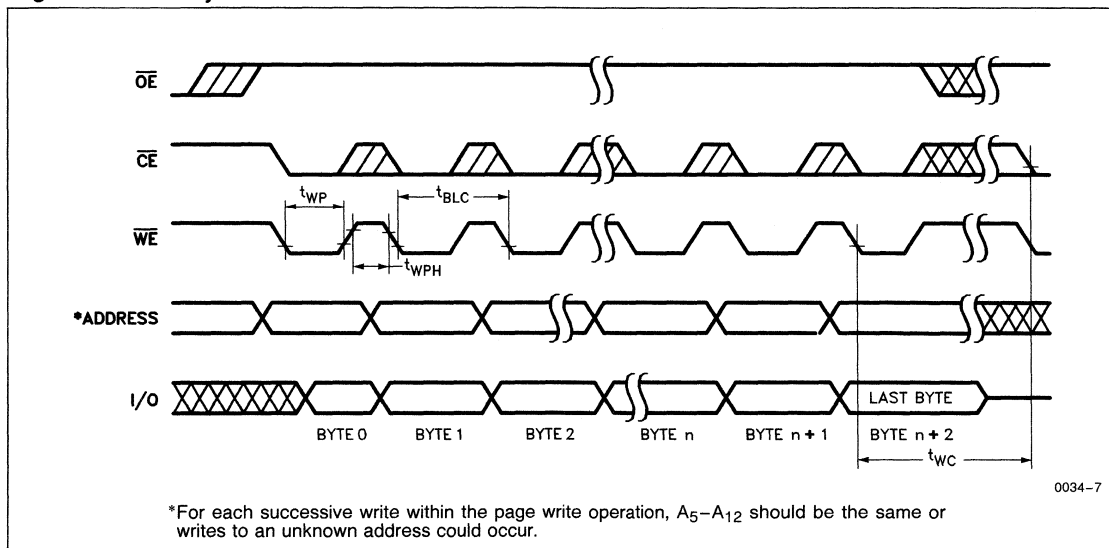
# X2864H, X2864HI

## CE Controlled Write Cycle



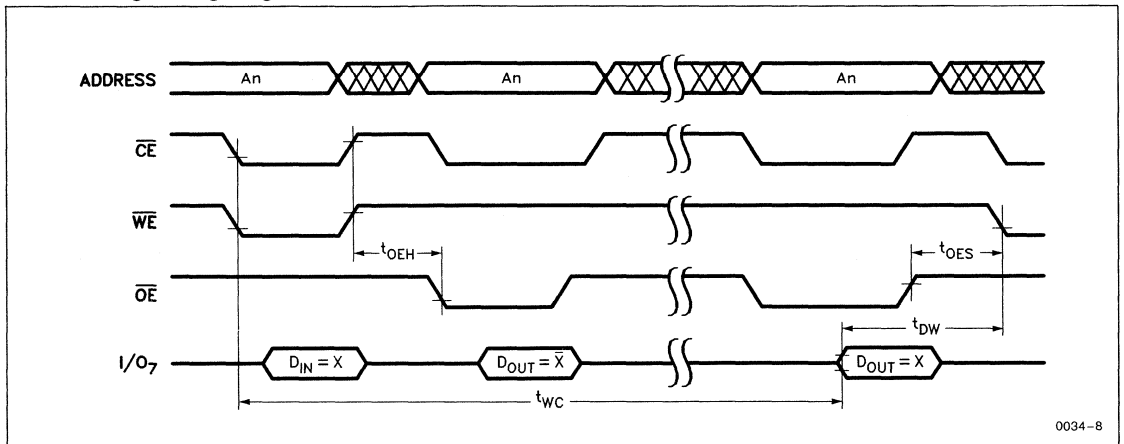
3

## Page Mode Write Cycle



# X2864H, X2864HI

## DATA Polling Timing Diagram





# X2864H, X2864HI

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{12}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2864H through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864H.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864H supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 3 ms.

### Page Write Operation

The page write feature of the X2864H allows the entire memory to be written in 750 ms. Page write allows two

to thirty-two bytes of data to be consecutively written to the X2864H prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is,  $A_5$  through  $A_{12}$  must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to thirty-one bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the 100  $\mu$ s byte load cycle time.

### DATA Polling

The X2864H features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864H, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

### WRITE PROTECTION

There are two features that protect the nonvolatile data from inadvertent writes.

- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 4.0V$ .
- Write Inhibit—Holding  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

# X2864H, X2864HI

## SYSTEM CONSIDERATIONS

Because the X2864H is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

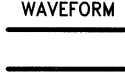




To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864H has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

64K

Military

X2864HM

8192 x 8 Bit

## Electrically Erasable PROM

### TYPICAL FEATURES

- 90 ns Access Time
- High Performance Scaled NMOS Technology
- Fast Write Cycle Times
  - 32-Byte Page Write Operation
  - Byte or Page Write Cycle: 3 ms Typical
  - Complete Memory Rewrite: 750 ms Typical
  - Effective Byte Write Cycle Time of 95  $\mu$ s Typical
- DATA Polling
  - Allows User to Minimize Write Cycle Time
- Simple Byte and Page Write
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- JEDEC Approved Byte-Wide Pinout

### DESCRIPTION

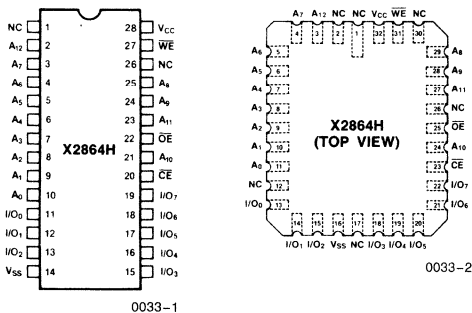
The Xicor X2864H is a high speed 8K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories it is a 5V only device. The X2864H features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs, ROMs and EPROMs.

The X2864H supports a 32-byte page write operation, effectively providing a 95  $\mu$ s/byte write cycle and enabling the entire memory to be written in less than 750 ms. The X2864H also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

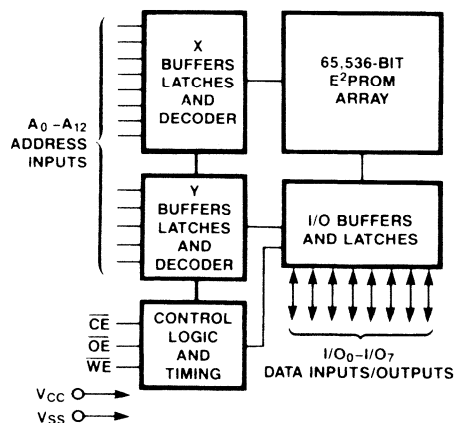
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>12</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
OE	Output Enable
V <sub>CC</sub>	+5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X2864HM

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on Any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		80	150	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		50	80	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	1	ms
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0.4V to 2.4V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	0.8V and 2.0V
Output Load	1 TTL Gate and $C_L = 30 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X2864HM

## A.C. CHARACTERISTICS

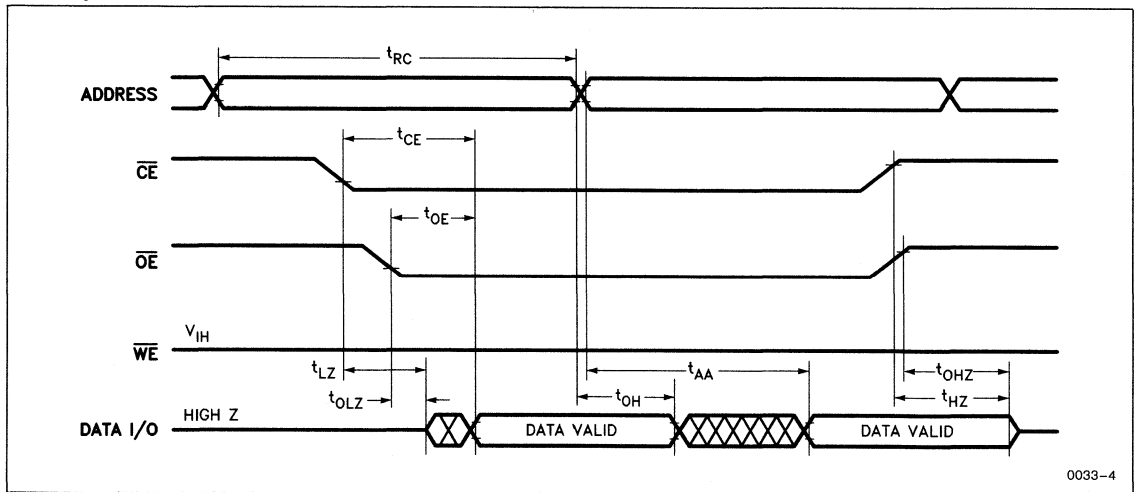
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	Min.	Max.	Units
$t_{RC}$	Read Cycle Time	90		ns
$t_{CE}$	Chip Enable Access Time		90	ns
$t_{AA}$	Address Access Time		90	ns
$t_{OE}$	Output Enable Access Time		45	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	40	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	40	ns
$t_{OH}$	Output Hold from Address Change	0		ns

3

### Read Cycle



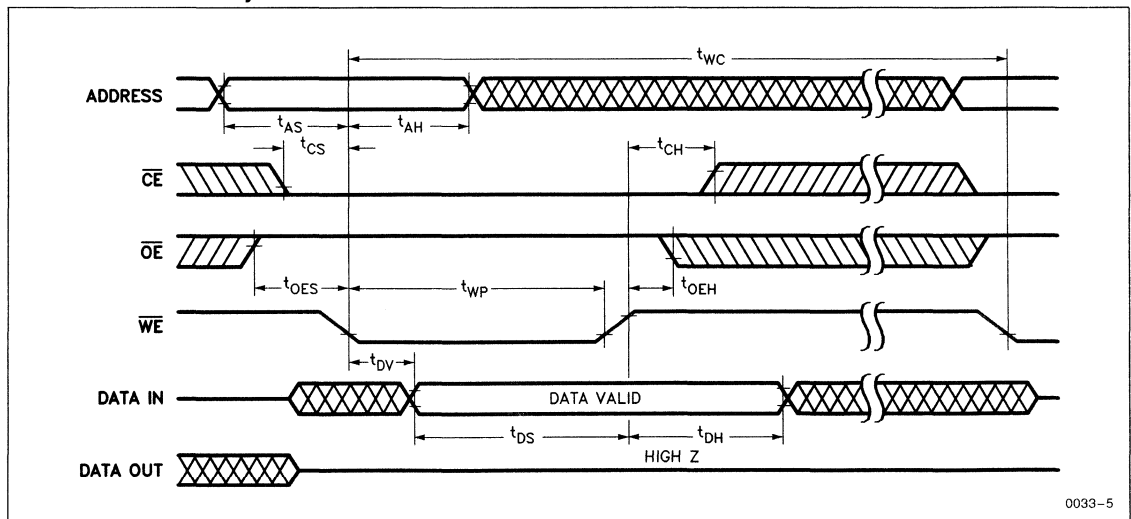
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X2864HM

## Write Cycle Limits

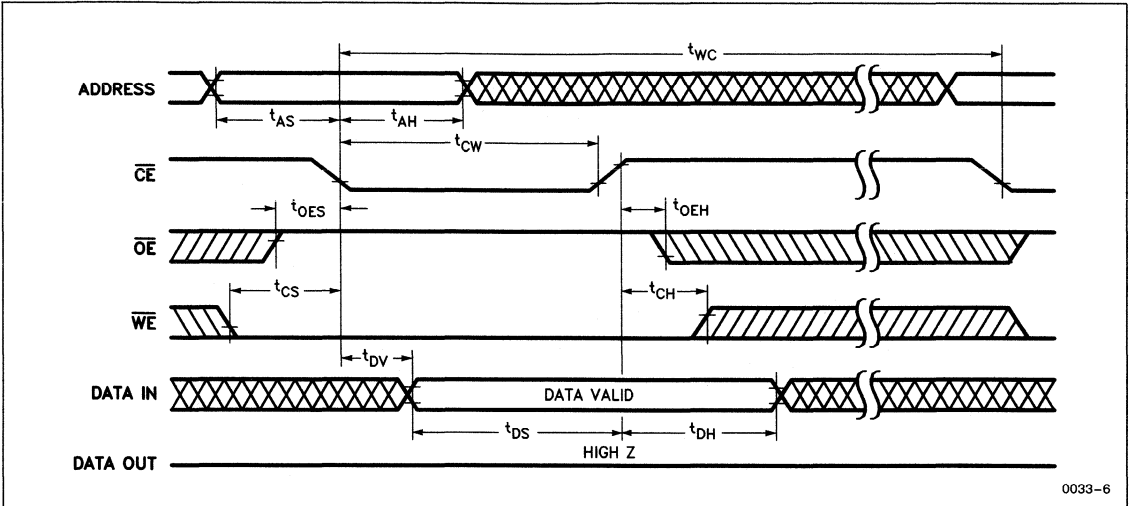
Symbol	Parameter	Min.	Max.	Units
$t_{WC}$	Write Cycle Time		5	ms
$t_{AS}$	Address Setup Time	5		ns
$t_{AH}$	Address Hold Time	50		ns
$t_{CS}$	Write Setup Time	0		ns
$t_{CH}$	Write Hold Time	0		ns
$t_{CW}$	$\overline{CE}$ Pulse Width	80		ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10		ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	5		ns
$t_{WP}$	$\overline{WE}$ Pulse Width	80		ns
$t_{WPH}$	$\overline{WE}$ High Recovery	500		ns
$t_{DV}$	Data Valid		100	$\mu$ s
$t_{DS}$	Data Setup	35		ns
$t_{DH}$	Data Hold	5		ns
$t_{DW}$	Delay to Next Write	10		$\mu$ s
$t_{BLC}$	Byte Load Cycle	1	100	$\mu$ s

## $\overline{WE}$ Controlled Write Cycle



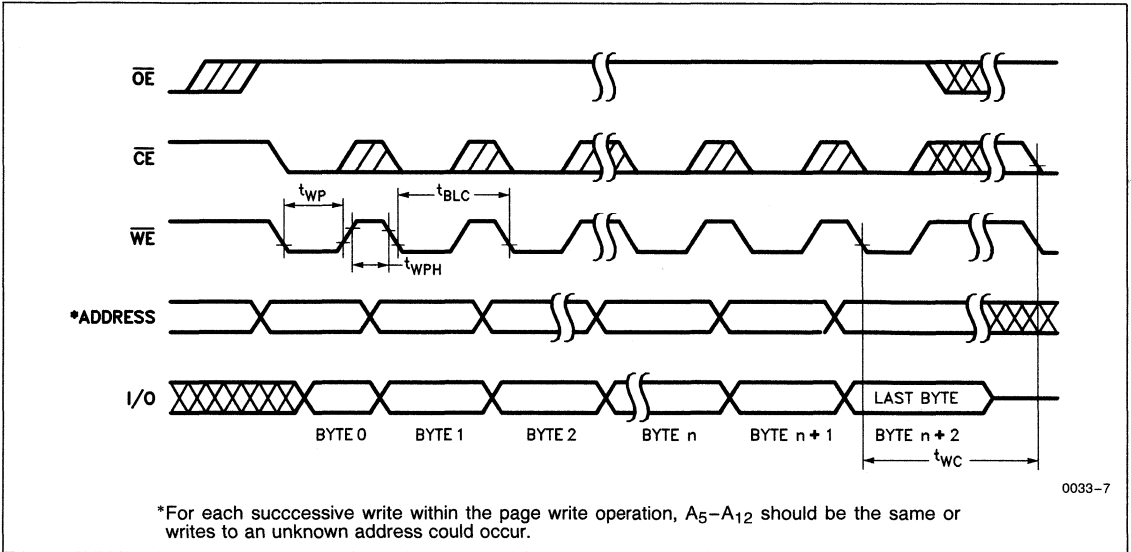
# X2864HM

## CE Controlled Write Cycle



3

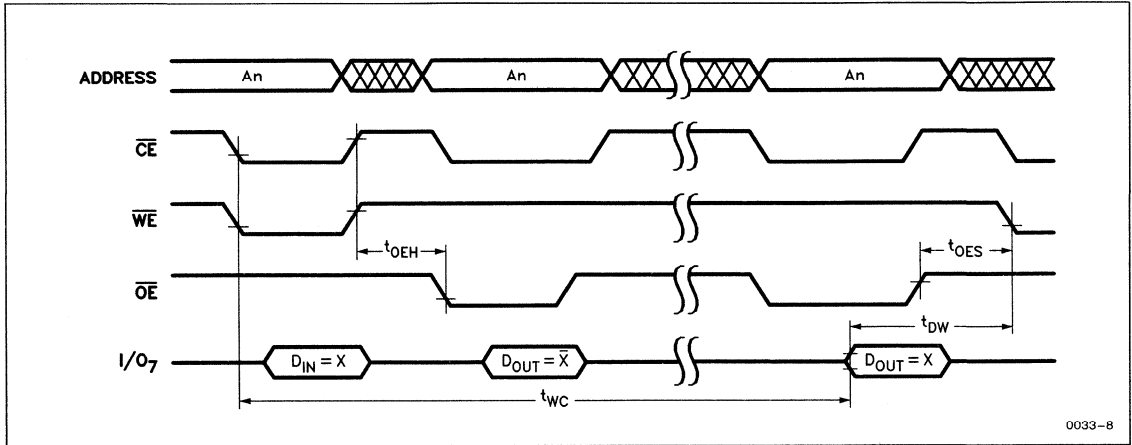
## Page Mode Write Cycle



\*For each successive write within the page write operation,  $A_5-A_{12}$  should be the same or writes to an unknown address could occur.

# X2864HM

## DATA Polling Timing Diagram





# X2864HM

---

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{12}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X2864H through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X2864H.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X2864H supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 3 ms.

### Page Write Operation

The page write feature of the X2864H allows the entire memory to be written in 750 ms. Page write allows two

to thirty-two bytes of data to be consecutively written to the X2864H prior to the commencement of the internal programming cycle. The destination addresses for a page write operation must reside on the same page; that is,  $A_5$  through  $A_{12}$  must not change.

The page write mode can be entered during any write operation. Following the initial byte write cycle, the host can write an additional one to thirty-one bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the 100  $\mu$ s byte load cycle time.

### DATA Polling

The X2864H features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X2864H, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data.

### WRITE PROTECTION

There are two features that protect the nonvolatile data from inadvertent writes.

- $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 4.0V$ .
- Write Inhibit—Holding  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH or  $\overline{CE}$  HIGH during power-on and power-off, will inhibit inadvertent writes.

# X2864HM

## SYSTEM CONSIDERATIONS

Because the X2864H is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

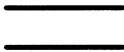




To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

Because the X2864H has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

**256K Commercial X28256 32K x 8 Bit**  
**Industrial X28256I**

## Electrically Erasable PROM

### FEATURES

- **250 ns Access Time**
- **Fast Write Cycle Times**
  - 64-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 2.5 Sec. Typical
  - Effective Byte Write Cycle Time: 78  $\mu$ s Typical
- **Software Data Protection**
- **End of Write Detection**
  - DATA Polling
  - Toggle Bit
- **Simple Byte and Page Write**
  - Single TTL Level WE Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **Upward Compatible with X2864A**
- **JEDEC Approved Byte-Wide Pinout**

### DESCRIPTION

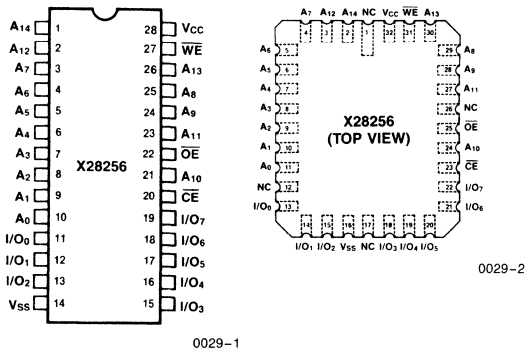
The Xicor X28256 is a 32K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories the X28256 is a 5V only device. The X28256 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs.

The X28256 supports a 64-byte page write operation, effectively providing a 78  $\mu$ s/byte write cycle and enabling the entire memory to be typically written in less than 2.5 seconds. The X28256 also features DATA Polling, a system software support scheme used to indicate the early completion of a write cycle. In addition, the X28256 includes a user-optional software data protection mode that further enhances Xicor's hardware write protect capability.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

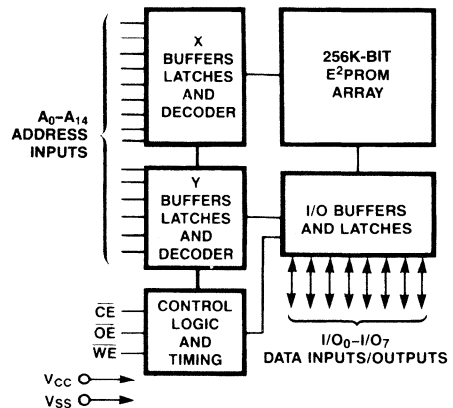
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>14</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
WE	Write Enable
CE	Chip Enable
OE	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0029-3

# X28256, X28256I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X28256	-10°C to +85°C
X28256I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X28256  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

X28256I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		60	120	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		35	60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 0.5$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	100	$\mu\text{s}$
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X28256, X28256I

## A.C. CHARACTERISTICS

X28256  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

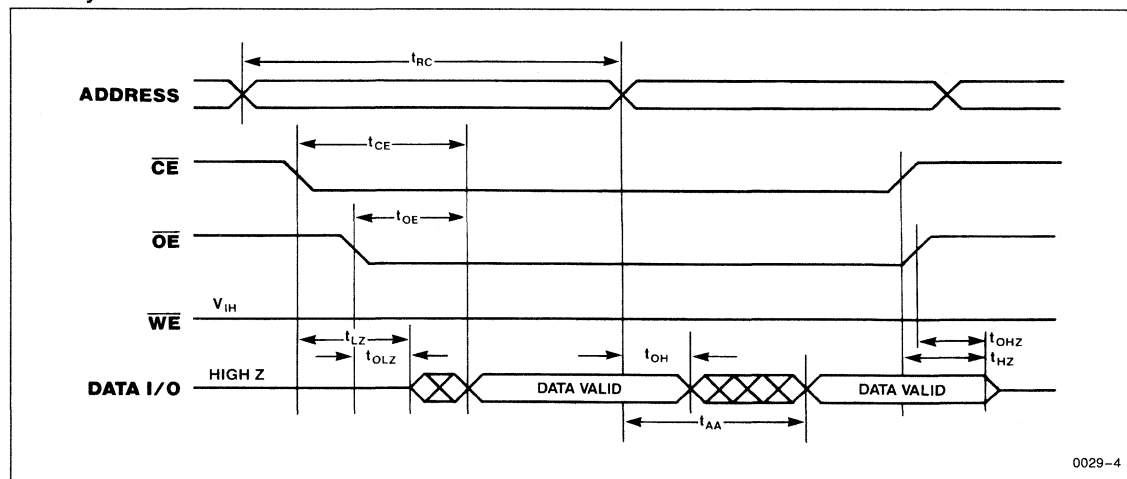
X28256I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X28256-25 X28256I-25		X28256 X28256I		X28256-35 X28256I-35		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		ns
$t_{CE}$	Chip Enable Access Time		250		300		350	ns
$t_{AA}$	Address Access Time		250		300		350	ns
$t_{OE}$	Output Enable Access Time		100		100		100	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	80	0	80	0	80	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	80	0	80	0	80	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

3

### Read Cycle



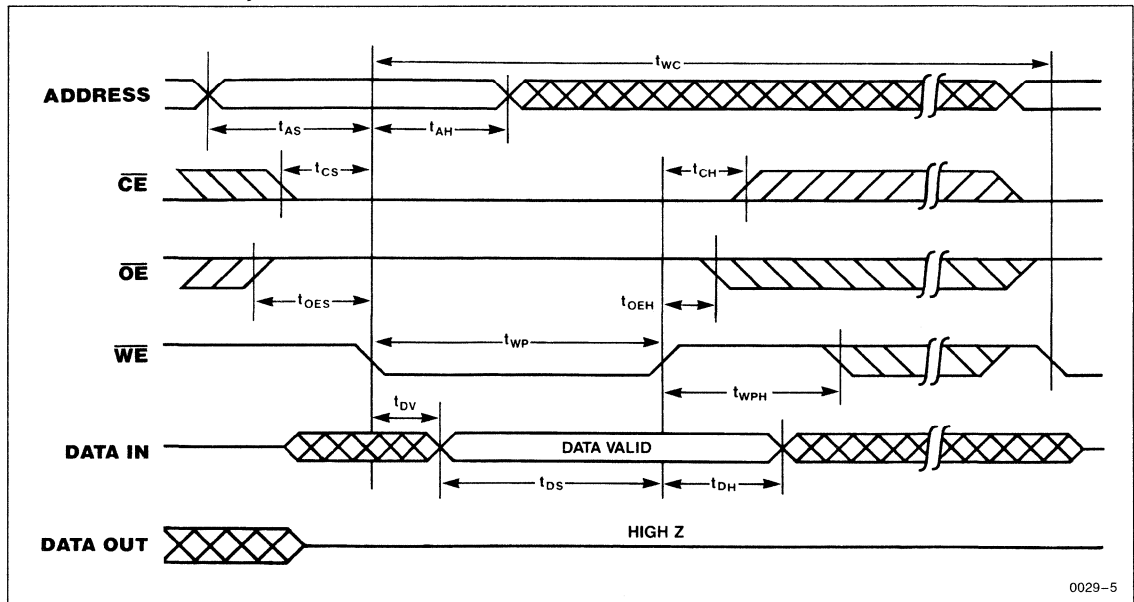
Note: (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X28256, X28256I

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		5	10	ms
$t_{AS}$	Address Setup Time	0			ns
$t_{AH}$	Address Hold Time	150			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	150			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	150			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	1			$\mu$ s
$t_{DV}$	Data Valid			300	ns
$t_{DS}$	Data Setup	100			ns
$t_{DH}$	Data Hold	15			ns
$t_{DW}$	Delay to Next Write	10			$\mu$ s
$t_{BLC}$	Byte Load Cycle	2		100	$\mu$ s

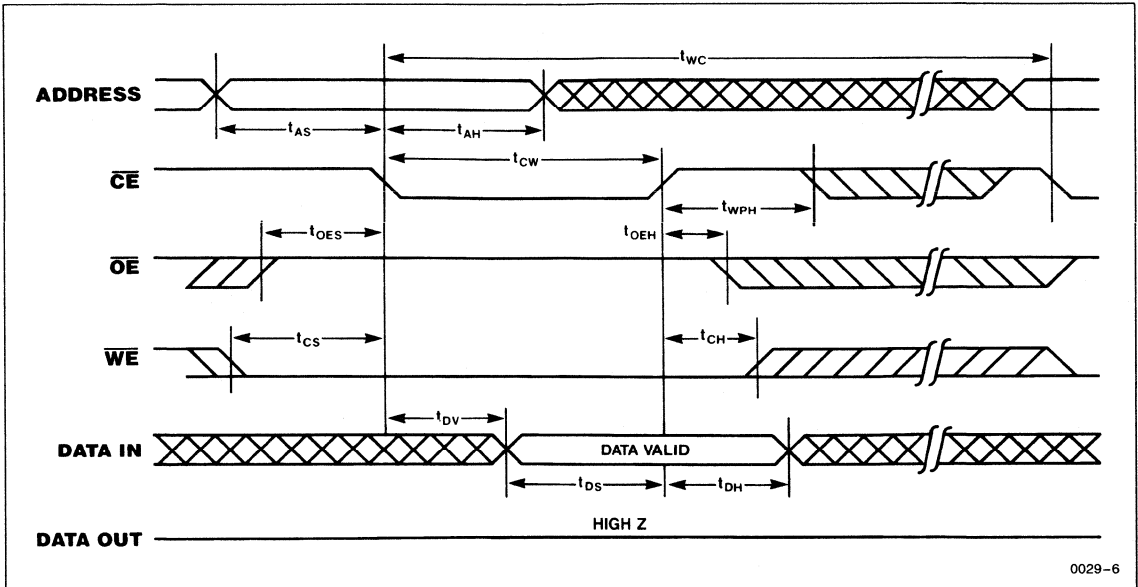
## $\overline{WE}$ Controlled Write Cycle



0029-5

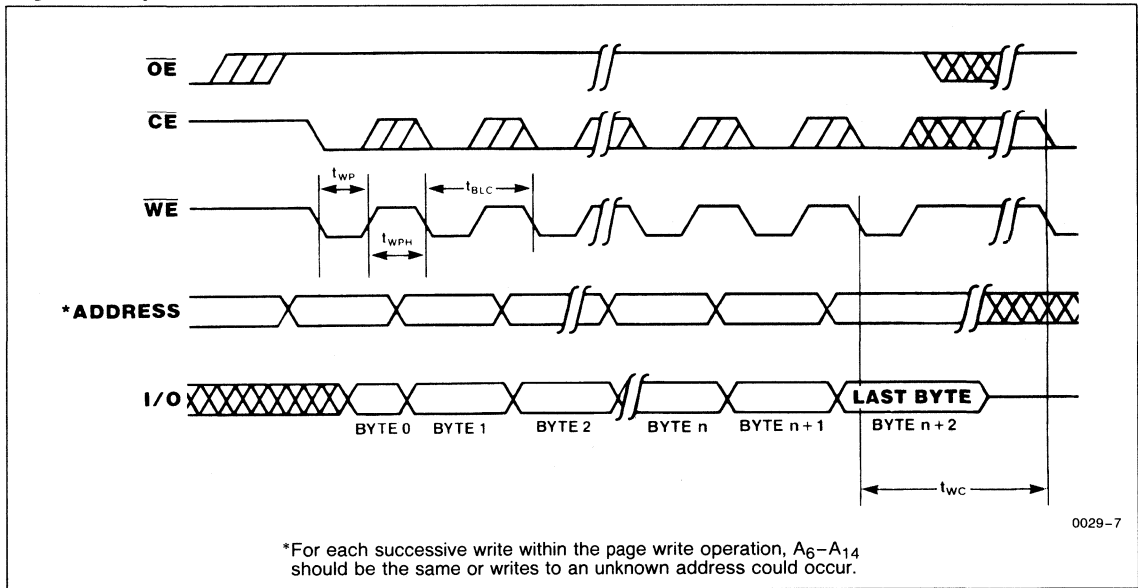
Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

**CE Controlled Write Cycle**



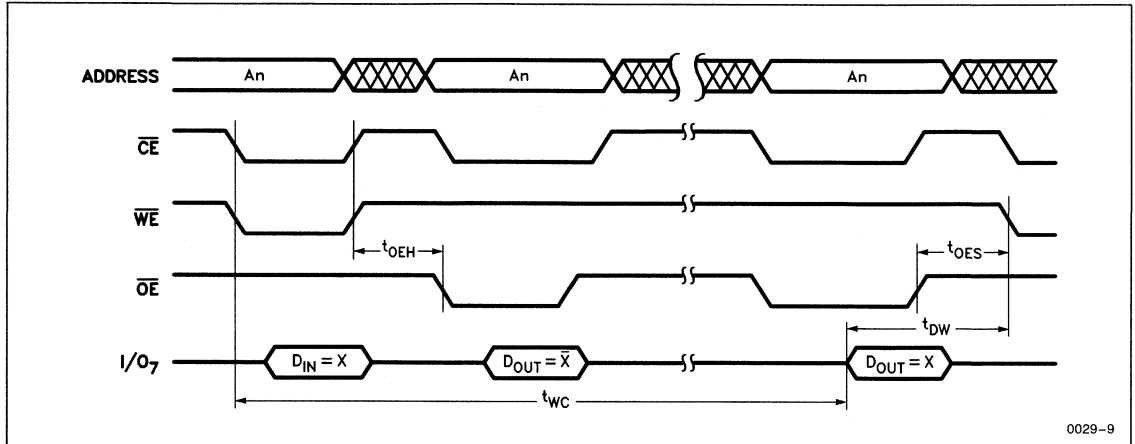
3

**Page Write Cycle**

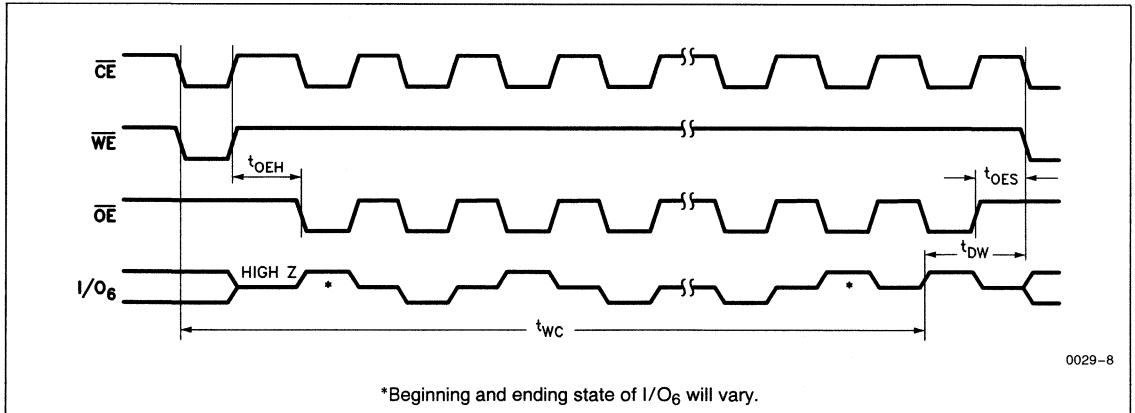


# X28256, X28256I

## DATA Polling Timing Diagram



## Toggle Bit Timing Diagram





# X28256, X28256I

## PIN DESCRIPTIONS

### Addresses (A<sub>0</sub>–A<sub>14</sub>)

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out (I/O<sub>0</sub>–I/O<sub>7</sub>)

Data is written to or read from the X28256 through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X28256.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW *and*  $\overline{OE}$  is HIGH. The X28256 supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

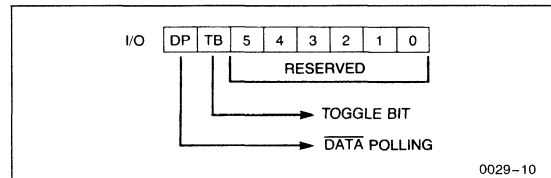
The page write feature of the X28256 allows the entire memory to be written in 2.5 seconds. Page write allows two to sixty-four bytes of data to be consecutively written to the X28256 prior to the commencement of the internal programming cycle. The host can fetch data from another location within the system during a page write operation (change the source address), but the page address (A<sub>6</sub> through A<sub>14</sub>) for each subsequent valid write cycle to the part during this operation must be the same as the initial page address.

The page write mode can be initiated during any write operation. Following the initial byte write cycle, the host can write an additional one to sixty-three bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 100  $\mu$ s.

### Write Operation Status Bits

The X28256 provides the user two write operation status bits. These can be used to optimize a system write cycle time. The status bits are mapped onto the I/O bus as shown in Figure 1.

Figure 1: Status Bit Assignment



### DATA Polling (I/O<sub>7</sub>)

The X28256 features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X28256, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on I/O<sub>7</sub> (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete, I/O<sub>7</sub> will reflect true data. Note: If the X28256 is in the protected state and an illegal write operation is attempted  $\overline{DATA}$  Polling will not operate.

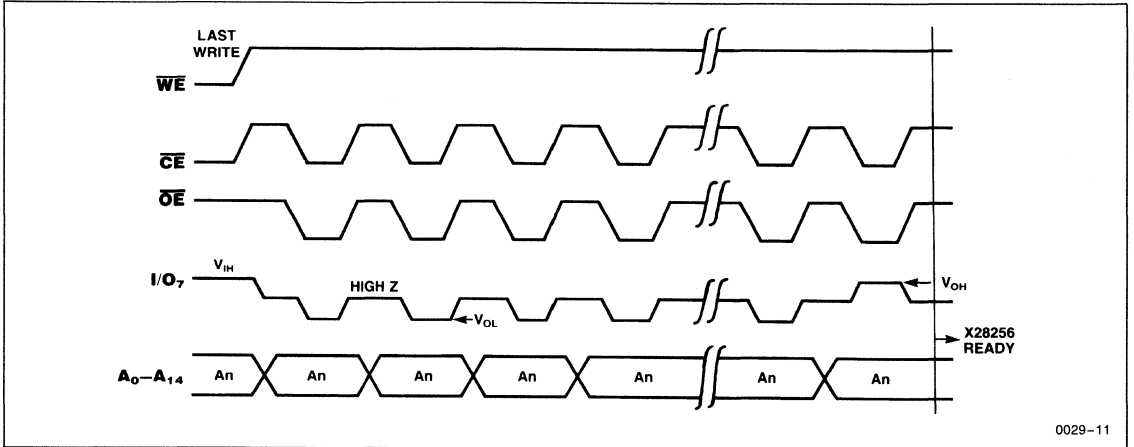
### Toggle Bit (I/O<sub>6</sub>)

The X28256 also provides another method for determining when the internal write cycle is complete. During the internal programming cycle I/O<sub>6</sub> will toggle from one to zero and zero to one on subsequent attempts to read the device. When the internal cycle is complete the toggling will cease and the device will be accessible for additional read or write operations.

# X28256, X28256I

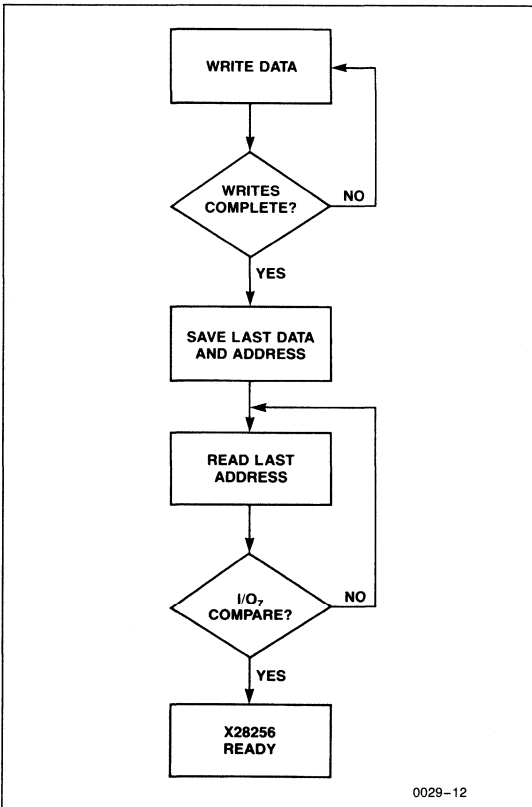
## DATA POLLING I/O<sub>7</sub>

Figure 2a: DATA Polling Bus Sequence



0029-11

Figure 2b: DATA Polling Software Flow



0029-12

DATA Polling can effectively halve the time for writing to the X28256. The timing diagram in Figure 2a illustrates the sequence of events on the bus. The software flow diagram in Figure 2b illustrates one method of implementing the routine.

# X28256, X28256I

## THE TOGGLE BIT I/O<sub>6</sub>

Figure 3a: Toggle Bit Bus Sequence

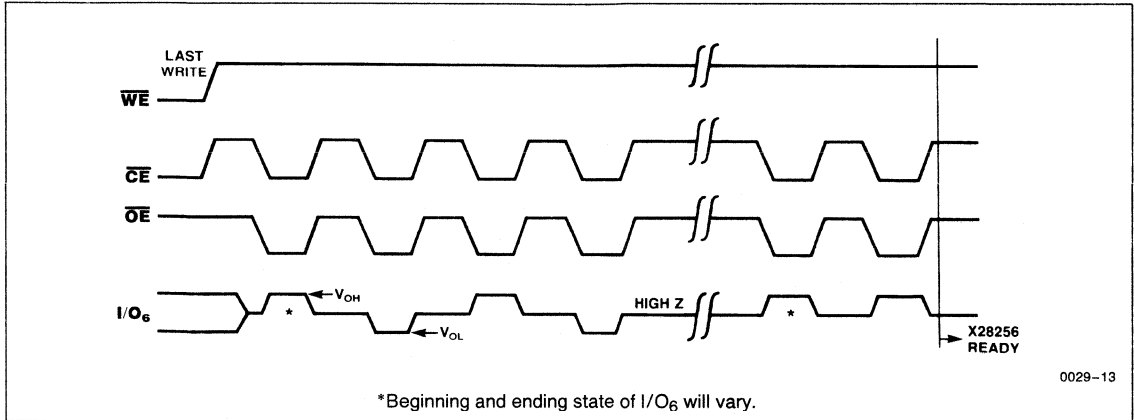
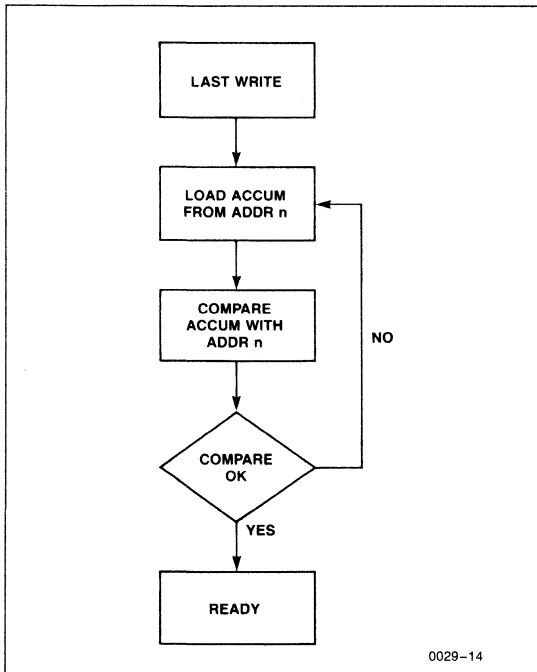


Figure 3b: Toggle Bit Software Flow



The Toggle Bit can eliminate the software housekeeping chore of saving and fetching the last address and data written to a device in order to implement  $\overline{\text{DATA}}$  Polling. This can be especially helpful in an array comprised of multiple X28256 memories that is frequently updated. The timing diagram in Figure 3a illustrates the sequence of events on the bus. The software flow diagram in Figure 3b illustrates a method for testing the Toggle Bit.

## X28256, X28256I

---

### HARDWARE DATA PROTECTION

The X28256 provides three hardware features (compatible with X2864A) that protect nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse less than 20 ns will not initiate a write cycle.
- Default  $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH, or  $\overline{CE}$  HIGH will prevent an inadvertent write cycle during power-on and power-off, maintaining data integrity.

### SOFTWARE DATA PROTECTION

The X28256 offers a software controlled data protection feature. The X28256 is shipped from Xicor with the software data protection NOT ENABLED; that is, the device will be in the standard operating mode. In this mode data should be protected during power-up/-down operations through the use of external circuits. The host would then have open read and write access of the device once  $V_{CC}$  was stable.

The X28256 can be automatically protected during power-up and power-down without the need for external circuits by employing the software data protection feature. The internal software data protection circuit is enabled after the first write operation utilizing the software algorithm. This circuit is nonvolatile and will remain set for the life of the device unless the reset command is issued.

Once the software protection is enabled, the X28256 is also protected from inadvertent and accidental writes in the powered-on state. That is, the software algorithm must be issued prior to writing additional data to the device.

### SOFTWARE ALGORITHM

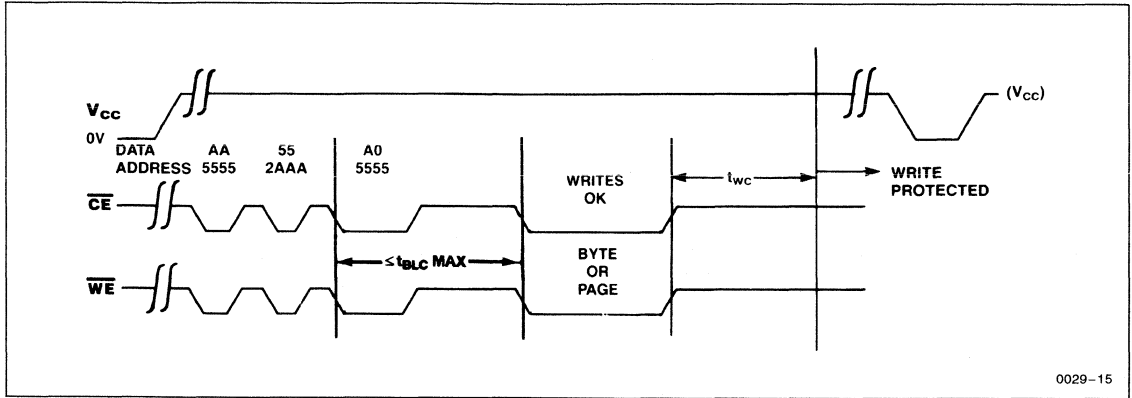
Selecting the software data protection mode requires the host system to precede data write operations by a series of three write operations to three specific addresses. Refer to Figure 4a and 4b for the sequence. The three byte sequence opens the page write window enabling the host to write from one to sixty-four bytes of data.<sup>(5)</sup> Once the page load cycle has been completed, the device will automatically be returned to the data protected state.

**Note:** (5) Once the three byte sequence is issued it must be followed by a valid byte or page write operation.

# X28256, X28256I

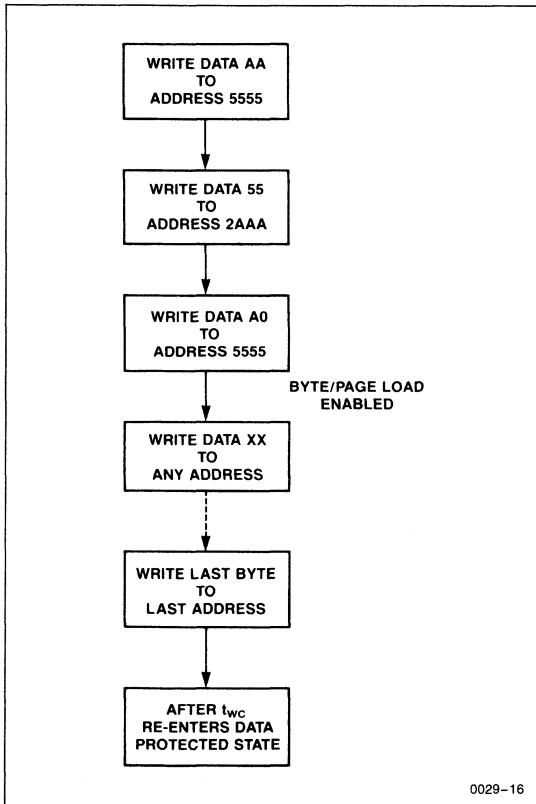
## SOFTWARE DATA PROTECTION

Figure 4a: Timing Sequence—Byte or Page Write



3

Figure 4b: Write Sequence for Software Data Protection



Regardless of whether the device has previously been protected or not, once the software data protected algorithm is used and data has been written, the X28256 will automatically disable further writes unless another command is issued to cancel it. If no further commands are issued the X28256 will be write protected during power-down and after any subsequent power-up.

**Note: Once initiated, the sequence of write operations should not be interrupted.**

# X28256, X28256I

## RESETTING SOFTWARE DATA PROTECTION

Figure 5a: Reset Software Data Protection Timing Sequence

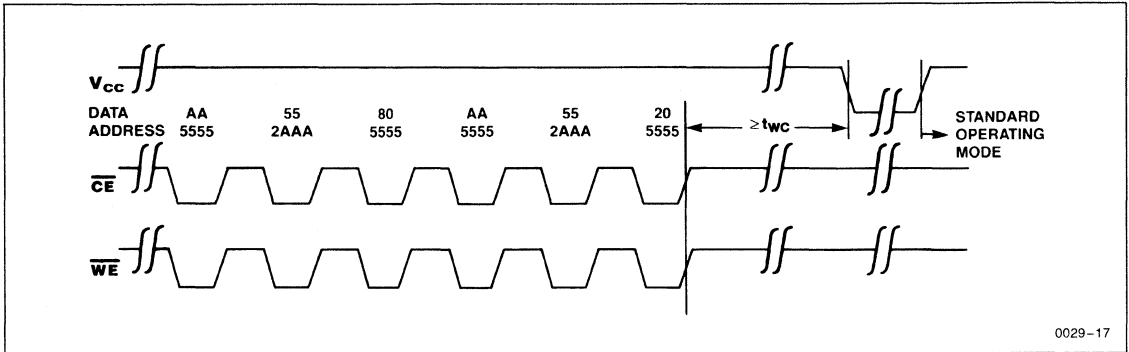
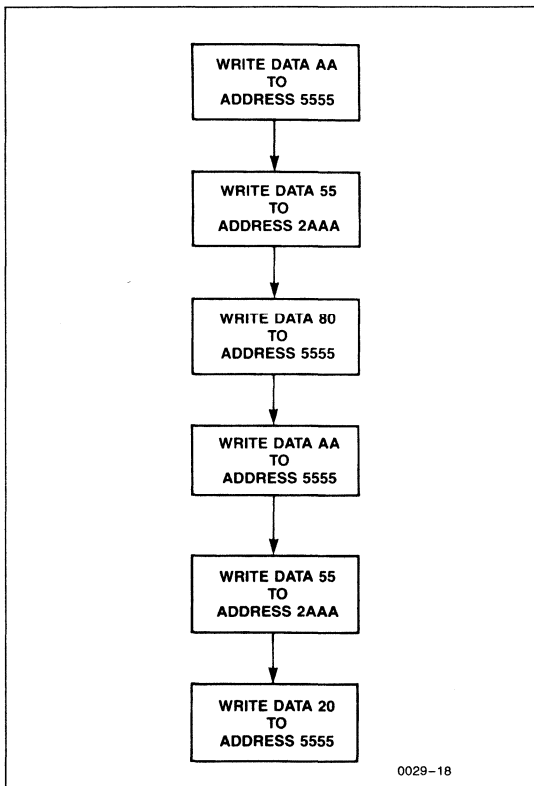


Figure 5b: Software Sequence to Deactivate Software Data Protection



In the event the user wants to deactivate the software data protection feature for testing or reprogramming in an E2PROM programmer, the following six step algorithm will reset the internal protection circuit. The next time the X28256 is powered-up the device will be in the standard operating mode.

**Note: Once initiated, the sequence of write operations should not be interrupted.**

## X28256, X28256I

### SYSTEM CONSIDERATIONS

Because the X28256 is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

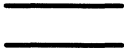




Because the X28256 has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

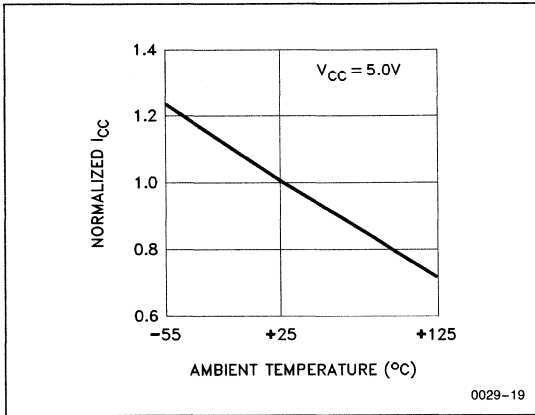
3

### SYMBOL TABLE

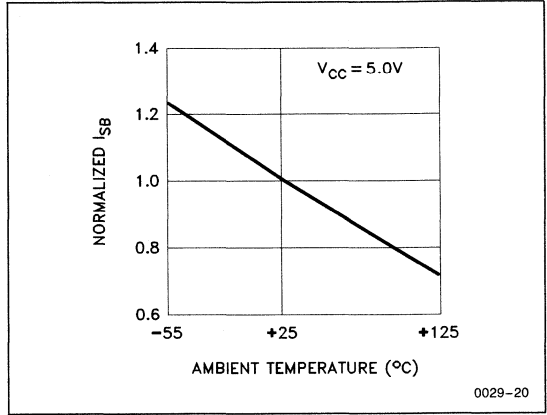
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X28256, X28256I

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**





**Electrically Erasable PROM**

**FEATURES**

- 250 ns Access Time
- Fast Write Cycle Times
  - 64-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 2.5 Sec. Typical
  - Effective Byte Write Cycle Time: 78  $\mu$ s Typical
- Software Data Protection
- End of Write Detection
  - DATA Polling
  - Toggle Bit
- Simple Byte and Page Write
  - Single TTL Level  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- Upward Compatible with X2864A
- JEDEC Approved Byte-Wide Pinout

**DESCRIPTION**

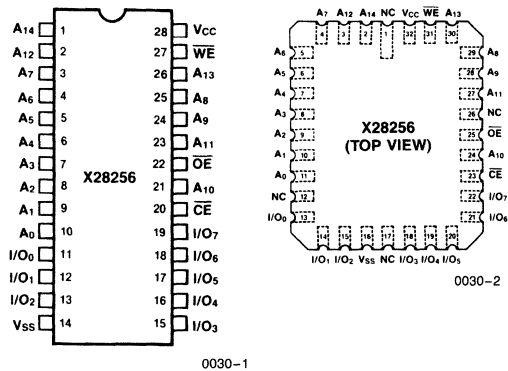
The Xicor X28256 is a 32K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories the X28256 is a 5V only device. The X28256 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs.

The X28256 supports a 64-byte page write operation, effectively providing a 78  $\mu$ s/byte write cycle and enabling the entire memory to be typically written in less than 2.5 seconds. The X28256 also features DATA Polling, a system software support scheme used to indicate the early completion of a write cycle. In addition, the X28256 includes a user-optional software data protection mode that further enhances Xicor's hardware write protect capability.

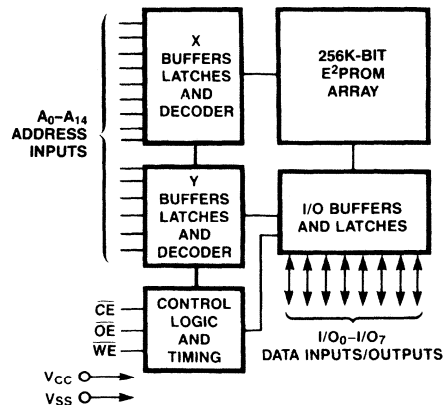
Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

**PIN CONFIGURATIONS**



**FUNCTIONAL DIAGRAM**



**PIN NAMES**

A <sub>0</sub> -A <sub>14</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

0030-3

# X28256M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias.....	-65°C to +135°C
Storage Temperature.....	-65°C to +150°C
Voltage on any Pin with Respect to Ground.....	-1.0V to +7V
D.C. Output Current.....	5 mA
Lead Temperature (Soldering, 10 Seconds).....	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5V \pm 5\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active)		60	120	mA	$\overline{CE} = \overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{SB}$	$V_{CC}$ Current (Standby)		35	60	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 0.5$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1 \text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400 \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	100	$\mu\text{s}$
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0 \text{ MHz}$ ,  $V_{CC} = 5V$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0V$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0V$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100 \text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X28256M

## A.C. CHARACTERISTICS

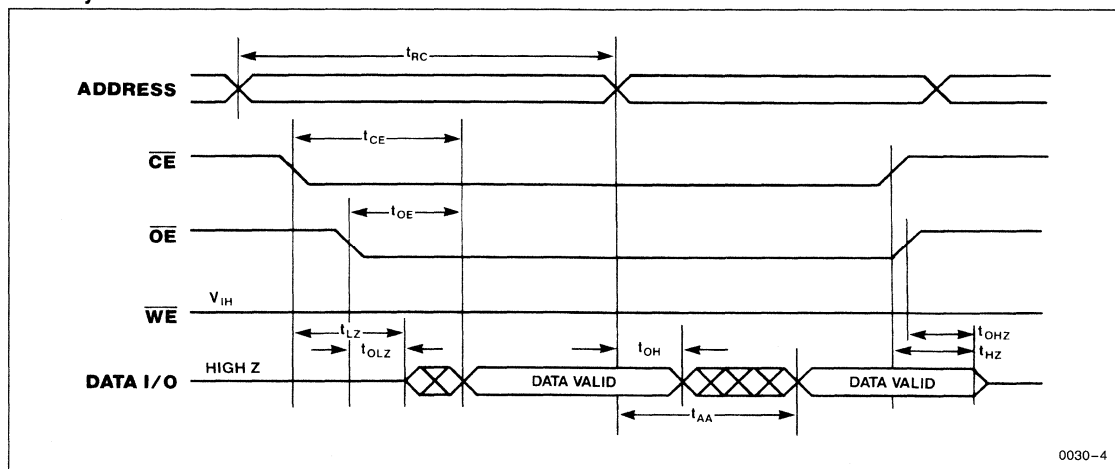
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 5\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X28256M-25		X28256M		X28256M-35		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		ns
$t_{CE}$	Chip Enable Access Time		250		300		350	ns
$t_{AA}$	Address Access Time		250		300		350	ns
$t_{OE}$	Output Enable Access Time		100		100		100	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	80	0	80	0	80	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	80	0	80	0	80	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

3

### Read Cycle



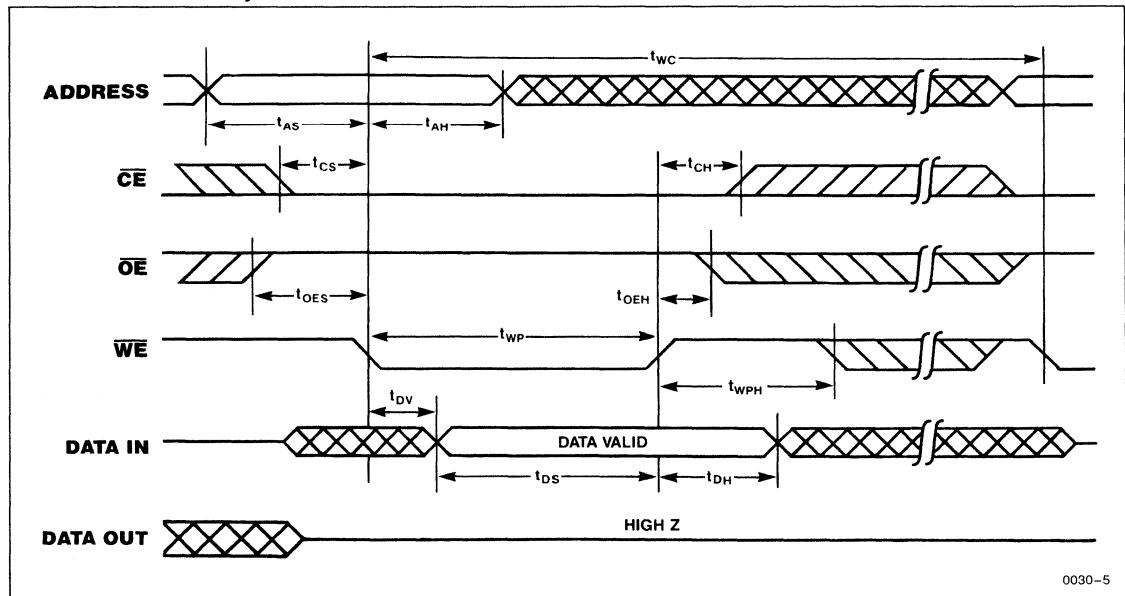
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X28256M

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		5	10	ms
$t_{AS}$	Address Setup Time	0			ns
$t_{AH}$	Address Hold Time	150			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	150			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	150			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	1			$\mu$ s
$t_{DV}$	Data Valid			300	ns
$t_{DS}$	Data Setup	100			ns </td
$t_{DH}$	Data Hold	15			ns
$t_{DW}$	Delay to Next Write	10			$\mu$ s
$t_{BLC}$	Byte Load Cycle	2		100	$\mu$ s

## $\overline{WE}$ Controlled Write Cycle

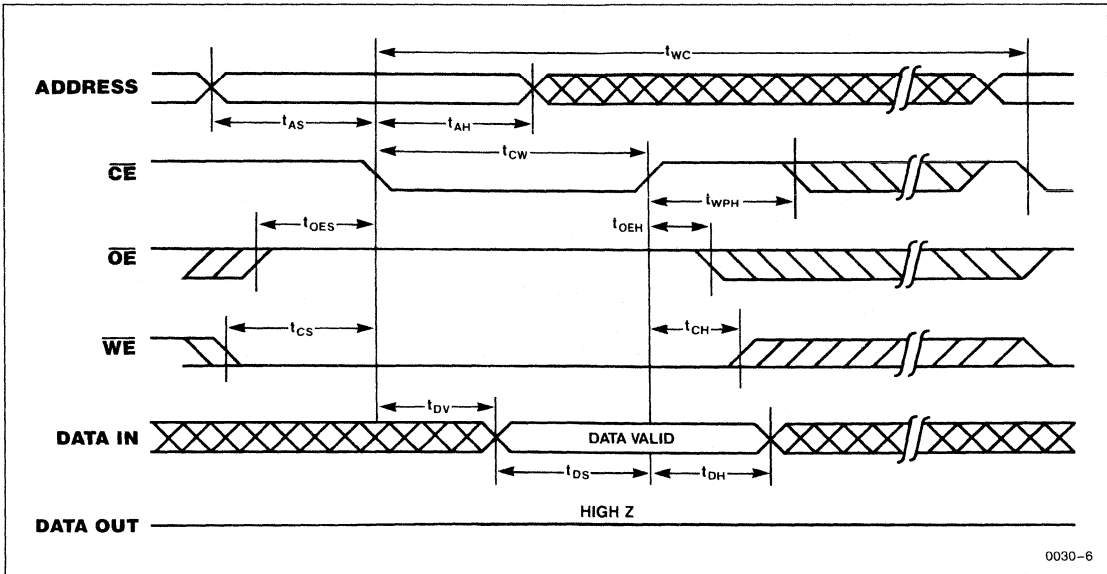


0030-5

Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

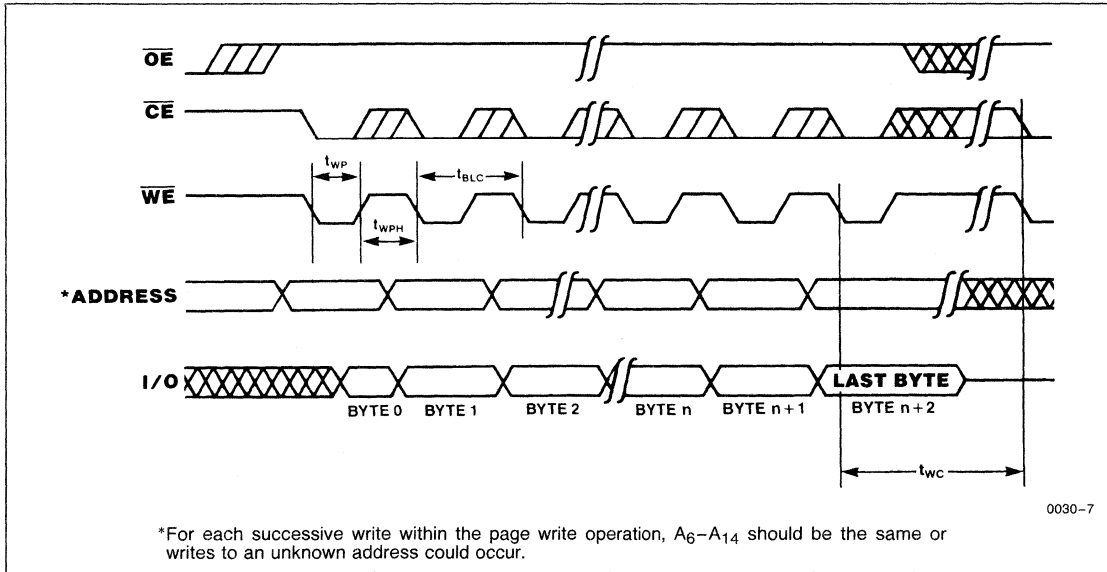
# X28256M

## $\overline{CE}$ Controlled Write Cycle



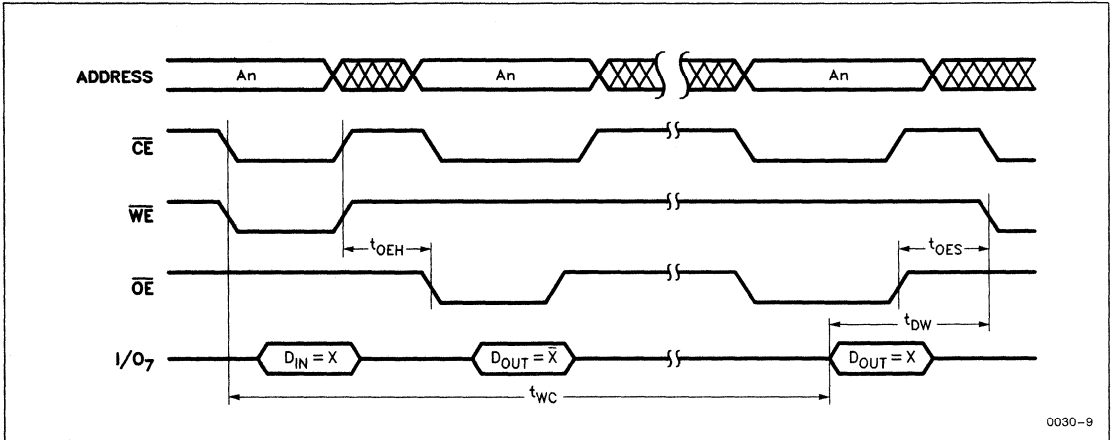
3

## Page Write Cycle

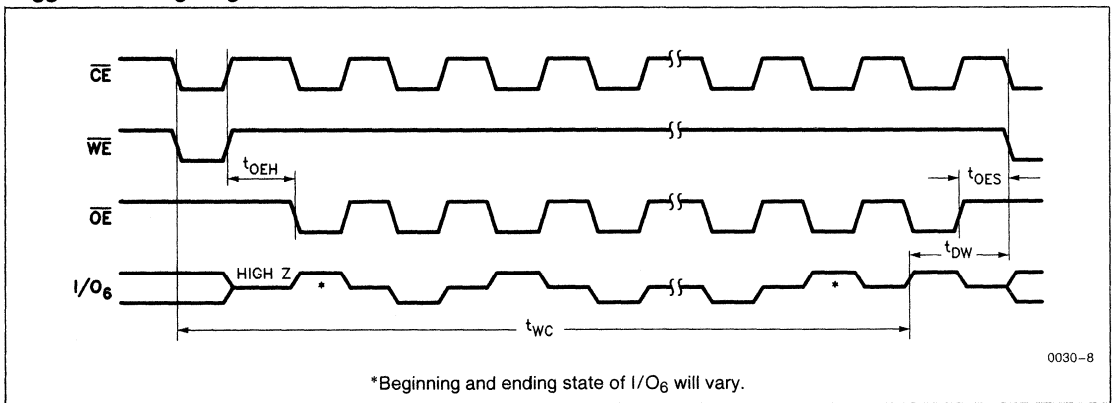


# X28256M

## DATA Polling Timing Diagram



## Toggle Bit Timing Diagram



# X28256M

## PIN DESCRIPTIONS

### Addresses (A<sub>0</sub>–A<sub>14</sub>)

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{\text{CE}}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{\text{CE}}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{\text{OE}}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out (I/O<sub>0</sub>–I/O<sub>7</sub>)

Data is written to or read from the X28256 through the I/O pins.

### Write Enable ( $\overline{\text{WE}}$ )

The Write Enable input controls the writing of data to the X28256.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{\text{OE}}$  and  $\overline{\text{CE}}$  LOW. The read operation is terminated by either  $\overline{\text{CE}}$  or  $\overline{\text{OE}}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{\text{OE}}$  or  $\overline{\text{CE}}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{\text{CE}}$  and  $\overline{\text{WE}}$  are LOW and  $\overline{\text{OE}}$  is HIGH. The X28256 supports both a  $\overline{\text{CE}}$  and  $\overline{\text{WE}}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{\text{CE}}$  or  $\overline{\text{WE}}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{\text{CE}}$  or  $\overline{\text{WE}}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

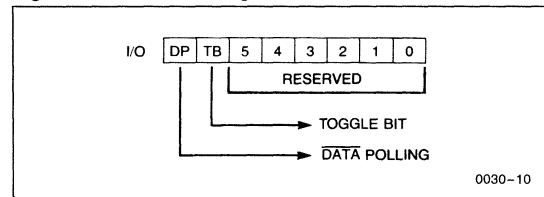
The page write feature of the X28256 allows the entire memory to be written in 2.5 seconds. Page write allows two to sixty-four bytes of data to be consecutively written to the X28256 prior to the commencement of the internal programming cycle. The host can fetch data from another location within the system during a page write operation (change the source address), but the page address (A<sub>6</sub> through A<sub>14</sub>) for each subsequent valid write cycle to the part during this operation must be the same as the initial page address.

The page write mode can be initiated during any write operation. Following the initial byte write cycle, the host can write an additional one to sixty-three bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{\text{WE}}$  HIGH to LOW transition, must begin within 100  $\mu\text{s}$  of the falling edge of the preceding  $\overline{\text{WE}}$ . If a subsequent  $\overline{\text{WE}}$  HIGH to LOW transition is not detected within 100  $\mu\text{s}$ , the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 100  $\mu\text{s}$ .

### Write Operation Status Bits

The X28256 provides the user two write operation status bits. These can be used to optimize a system write cycle time. The status bits are mapped onto the I/O bus as shown in Figure 1.

Figure 1: Status Bit Assignment



### DATA Polling (I/O<sub>7</sub>)

The X28256 features  $\overline{\text{DATA}}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{\text{DATA}}$  Polling allows a simple bit test operation to determine the status of the X28256, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on I/O<sub>7</sub> (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete, I/O<sub>7</sub> will reflect true data. Note: If the X28256 is in the protected state and an illegal write operation is attempted  $\overline{\text{DATA}}$  Polling will not operate.

### Toggle Bit (I/O<sub>6</sub>)

The X28256 also provides another method for determining when the internal write cycle is complete. During the internal programming cycle I/O<sub>6</sub> will toggle from one to zero and zero to one on subsequent attempts to read the device. When the internal cycle is complete the toggling will cease and the device will be accessible for additional read or write operations.

# X28256M

## DATA POLLING I/O<sub>7</sub>

Figure 2a: DATA Polling Bus Sequence

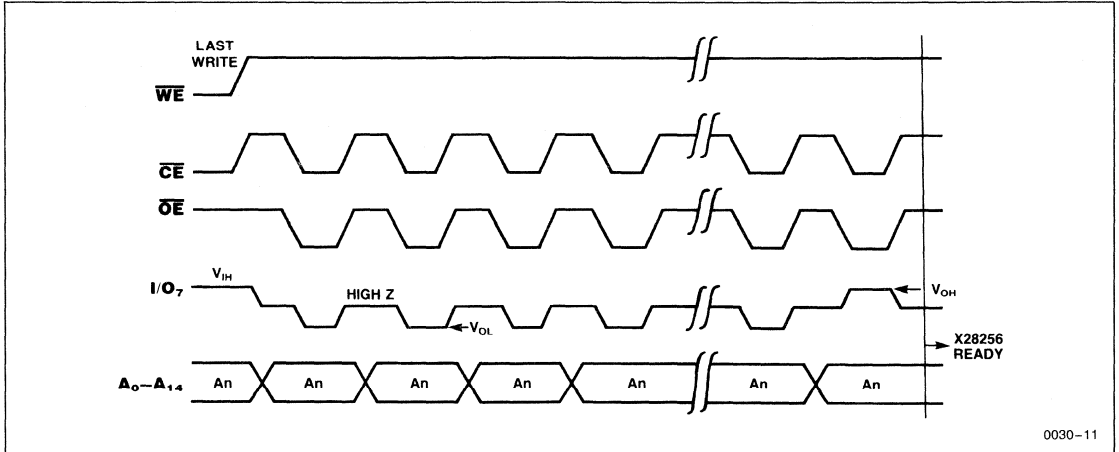
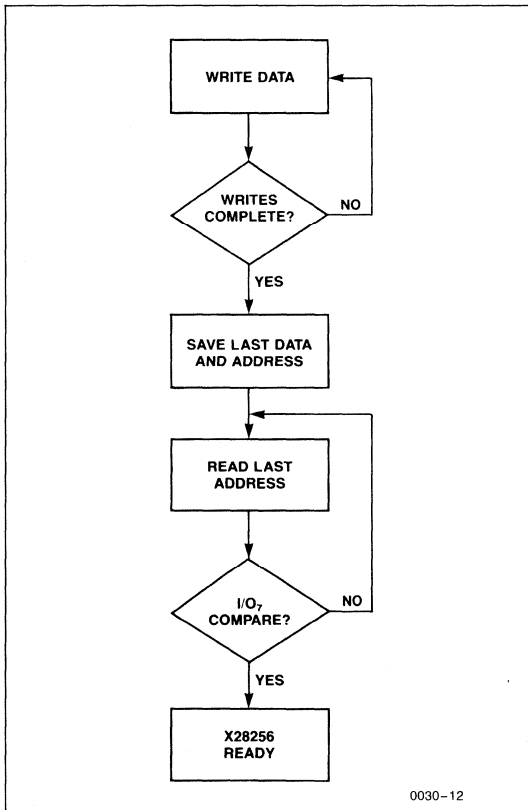


Figure 2b: DATA Polling Software Flow



DATA Polling can effectively halve the time for writing to the X28256. The timing diagram in Figure 2a illustrates the sequence of events on the bus. The software flow diagram in Figure 2b illustrates one method of implementing the routine.



# X28256M

## THE TOGGLE BIT I/O<sub>6</sub>

Figure 3a: Toggle Bit Bus Sequence

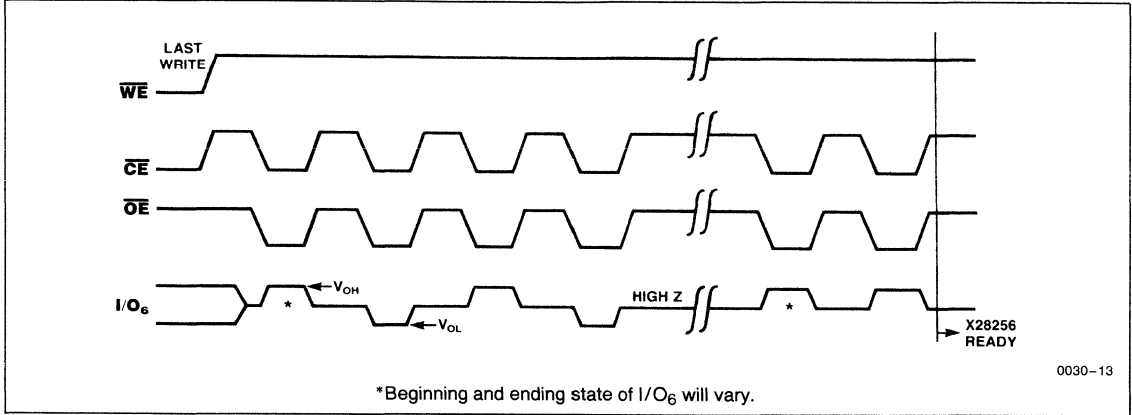
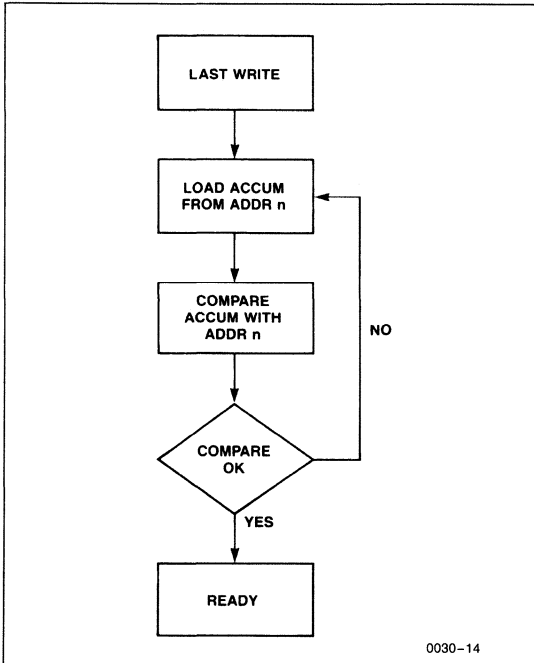


Figure 3b: Toggle Bit Software Flow



The Toggle Bit can eliminate the software housekeeping chore of saving and fetching the last address and data written to a device in order to implement DATA Polling. This can be especially helpful in an array comprised of multiple X28256 memories that is frequently updated. The timing diagram in Figure 3a illustrates the sequence of events on the bus. The software flow diagram in Figure 3b illustrates a method for testing the Toggle Bit.

## X28256M

---

### HARDWARE DATA PROTECTION

The X28256 provides three hardware features (compatible with X2864A) that protect nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse less than 20 ns will not initiate a write cycle.
- Default  $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH, or  $\overline{CE}$  HIGH will prevent an inadvertent write cycle during power-on and power-off, maintaining data integrity.

### SOFTWARE DATA PROTECTION

The X28256 offers a software controlled data protection feature. The X28256 is shipped from Xicor with the software data protection NOT ENABLED; that is, the device will be in the standard operating mode. In this mode data should be protected during power-up/-down operations through the use of external circuits. The host would then have open read and write access of the device once  $V_{CC}$  was stable.

The X28256 can be automatically protected during power-up and power-down without the need for external circuits by employing the software data protection feature. The internal software data protection circuit is enabled after the first write operation utilizing the software algorithm. This circuit is nonvolatile and will remain set for the life of the device unless the reset command is issued.

Once the software data protection is enabled, the X28256 is also protected from inadvertent and accidental writes in the powered-on state. That is, the software algorithm must be issued prior to writing additional data to the device.

### SOFTWARE ALGORITHM

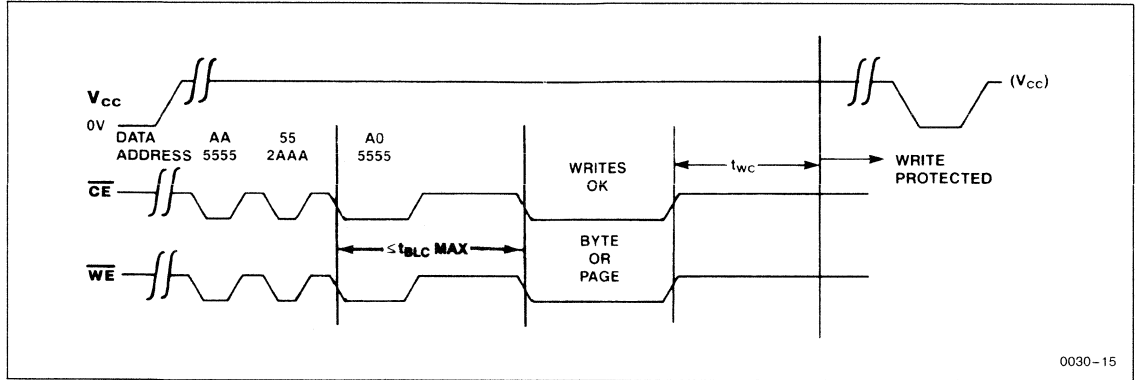
Selecting the software data protection mode requires the host system to precede data write operations by a series of three write operations to three specific addresses. Refer to Figure 4a and 4b for the sequence. The three byte sequence opens the page write window enabling the host to write from one to sixty-four bytes of data.<sup>(5)</sup> Once the page load cycle has been completed, the device will automatically be returned to the data protected state.

**Note:** (5) Once the three byte sequence is issued it must be followed by a valid byte or page write operation.

# X28256M

## SOFTWARE DATA PROTECTION

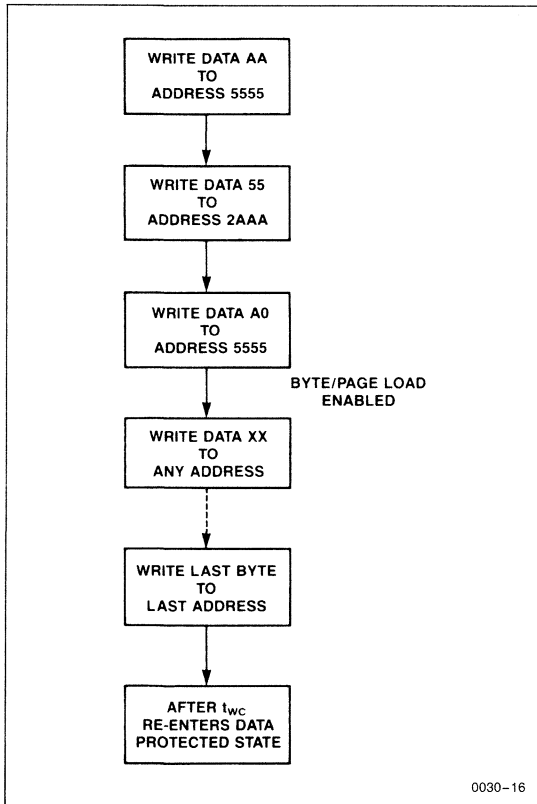
Figure 4a: Timing Sequence—Byte or Page Write



0030-15

3

Figure 4b: Write Sequence for Software Data Protection



0030-16

Regardless of whether the device has previously been protected or not, once the software data protected algorithm is used and data has been written, the X28256 will automatically disable further writes unless another command is issued to cancel it. If no further commands are issued the X28256 will be write protected during power-down and after any subsequent power-up.

**Note:** Once initiated, the sequence of write operations should not be interrupted.

# X28256M

## RESETTING SOFTWARE DATA PROTECTION

Figure 5a: Reset Software Data Protection Timing Sequence

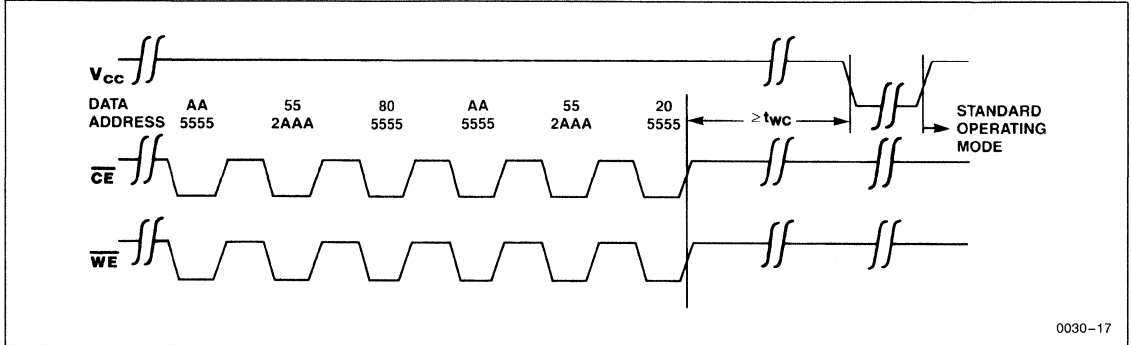
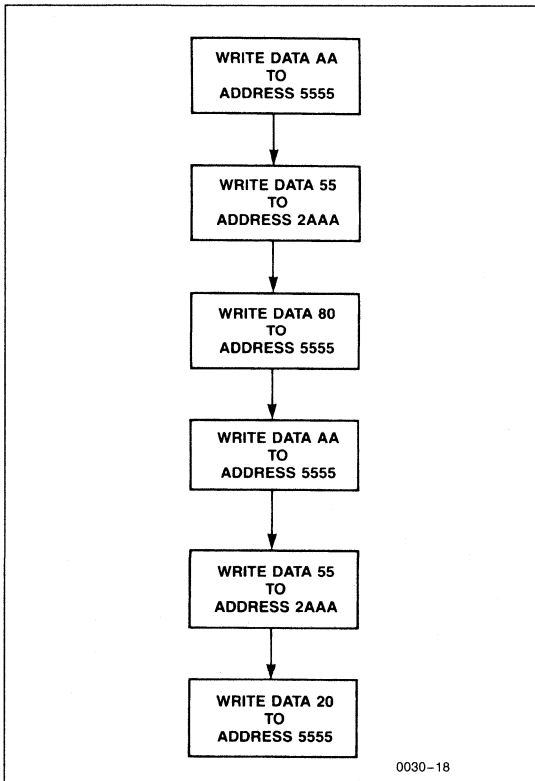


Figure 5b: Software Sequence to Deactivate Software Data Protection



In the event the user wants to deactivate the software data protection feature for testing or reprogramming in an E<sup>2</sup>PROM programmer, the following six step algorithm will reset the internal protection circuit. The next time the X28256 is powered-up the device will be in the standard operating mode.

**Note:** Once initiated, the sequence of write operations should not be interrupted.

## X28256M

### SYSTEM CONSIDERATIONS

Because the X28256 is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.






Because the X28256 has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

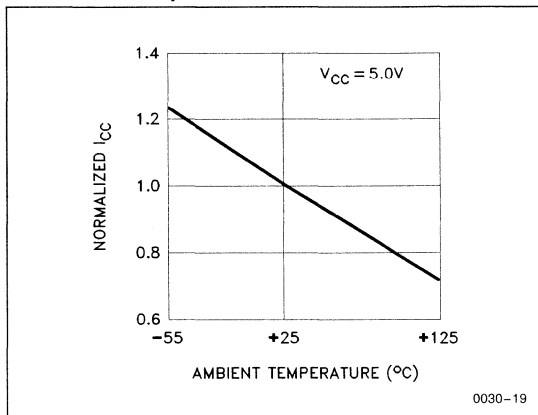
3

**SYMBOL TABLE**

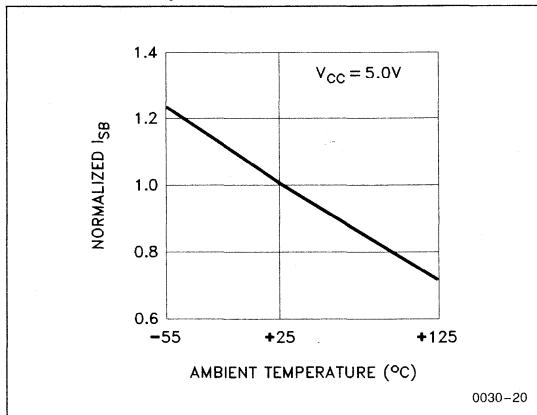
WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

# X28256M

**Normalized Active Supply Current vs. Ambient Temperature**



**Normalized Standby Supply Current vs. Ambient Temperature**



**256K Commercial X28C256 32K x 8 Bit**  
**Industrial X28C256I**

## Electrically Erasable PROM

### FEATURES

- **LOW Power CMOS**
  - 60 mA Active Current Max.
  - 200  $\mu$ A Standby Current Max.
- **Fast Write Cycle Times**
  - 64-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 2.5 Sec.

Typical

  - Effective Byte Write Cycle Time: 78  $\mu$ s Typical
- **Software Data Protection**
- **End of Write Detection**
  - DATA Polling
  - Toggle Bit
- **Simple Byte and Page Write**
  - Single TTL Compatible  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **Upward Compatible with X2864A**
- **JEDEC Approved Byte-Wide Pinout**

### DESCRIPTION

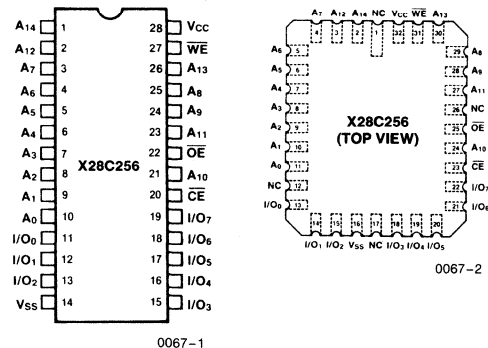
The Xicor X28C256 is a 32K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, floating gate CMOS technology. Like all Xicor programmable non-volatile memories the X28C256 is a 5V only device. The X28C256 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs.

The X28C256 supports a 64-byte page write operation, effectively providing a 78  $\mu$ s/byte write cycle and enabling the entire memory to be typically written in less than 2.5 seconds. The X28C256 also features DATA Polling, a system software support scheme used to indicate the early completion of a write cycle. In addition, the X28C256 includes a user-optional software data protection mode that further enhances Xicor's hardware write protect capability.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

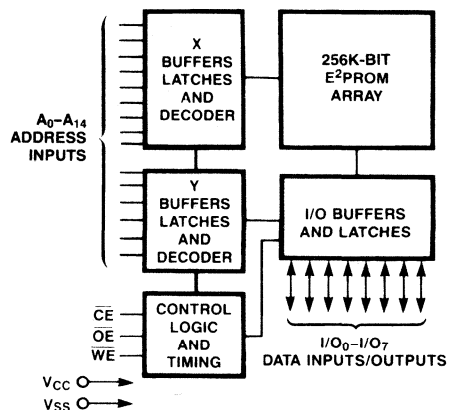
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> –A <sub>14</sub>	Address Inputs
I/O <sub>0</sub> –I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
CE	Chip Enable
OE	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X28C256, X28C256I

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	
X28C256	-10°C to +85°C
X28C256I	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X28C256  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

X28C256I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active) (TTL Inputs)			60	mA	$\overline{CE} = \overline{OE} = V_{IL}$ , $\overline{WE} = V_{IH}$ All I/O's = Open Address Inputs = TTL Levels @ $f = 5\text{ MHz}$
$I_{SB1}$	$V_{CC}$ Current (Standby) (TTL Inputs)			2	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open, Other Inputs = $V_{IH}$
$I_{SB2}$	$V_{CC}$ Current (Standby) (CMOS Inputs)		100	200	$\mu\text{A}$	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open, Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1\text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400\ \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	100	$\mu\text{s}$
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0\text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.



# X28C256, X28C256I

## A.C. CHARACTERISTICS

X28C256  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

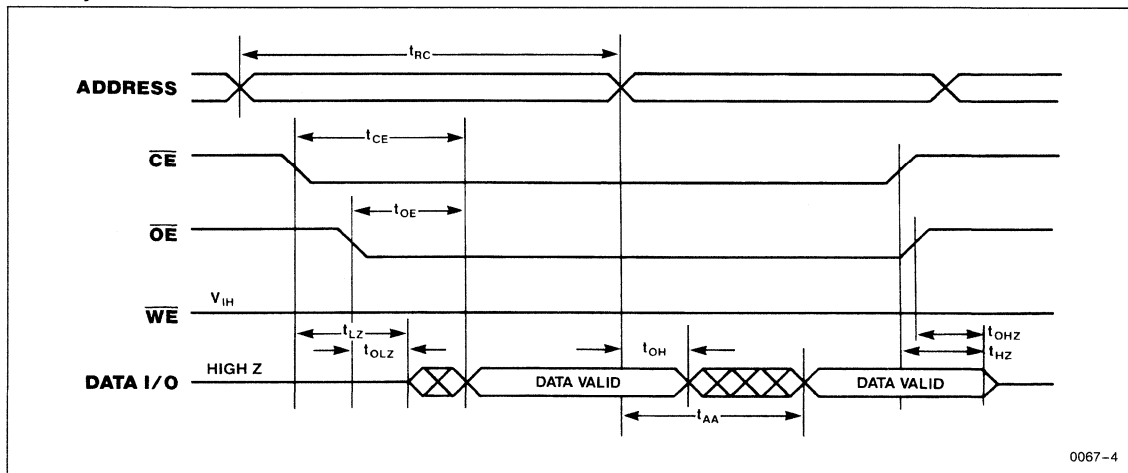
X28C256I  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X28C256-25 X28C256I-25		X28C256 X28C256I		X28C256-35 X28C256I-35		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		ns
$t_{CE}$	Chip Enable Access Time		250		300		350	ns
$t_{AA}$	Address Access Time		250		300		350	ns
$t_{OE}$	Output Enable Access Time		100		100		100	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

3

### Read Cycle



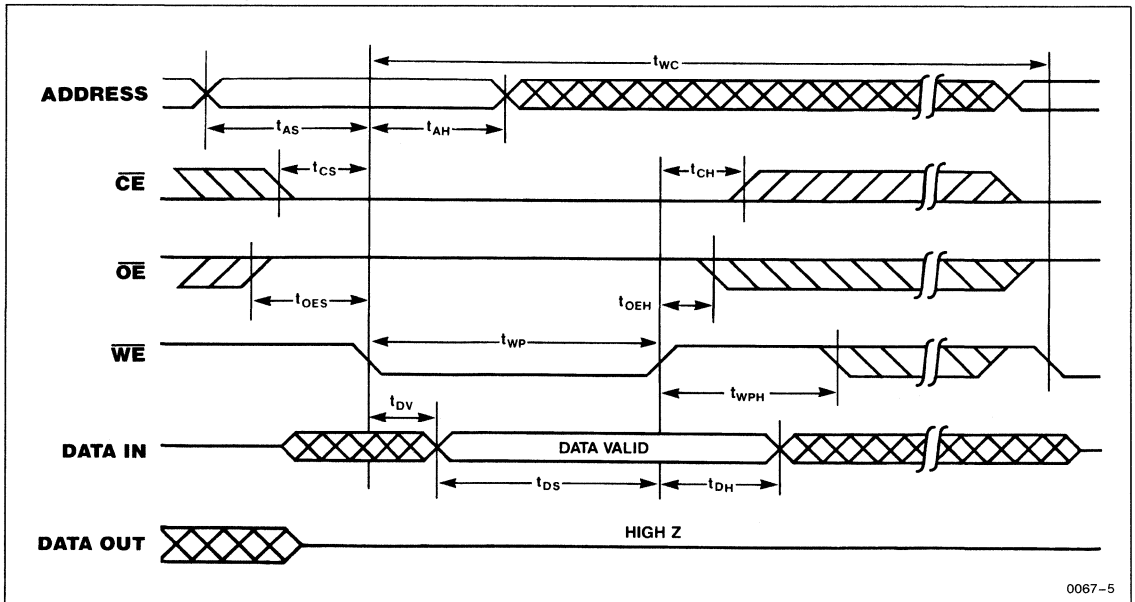
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

## X28C256, X28C256I

### Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		5	10	ms
$t_{AS}$	Address Setup Time	0			ns
$t_{AH}$	Address Hold Time	150			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	100			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	100			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	1			$\mu$ S
$t_{DV}$	Data Valid			1	$\mu$ S
$t_{DS}$	Data Setup	50			ns
$t_{DH}$	Data Hold	10			ns
$t_{DW}$	Delay to Next Write	10			$\mu$ S
$t_{BLC}$	Byte Load Cycle	1		100	$\mu$ S

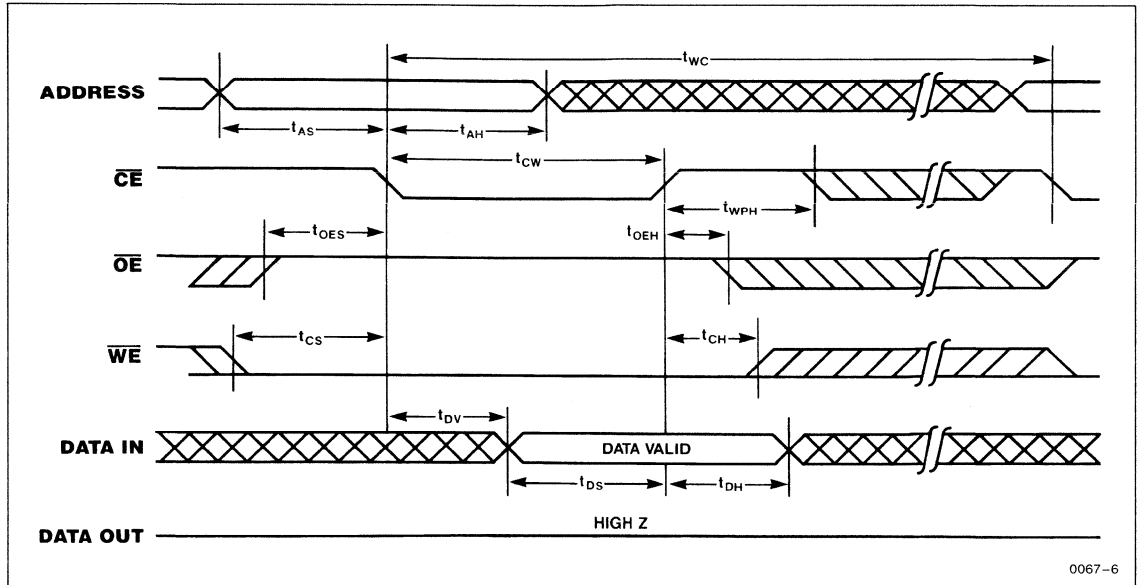
### $\overline{WE}$ Controlled Write Cycle



Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

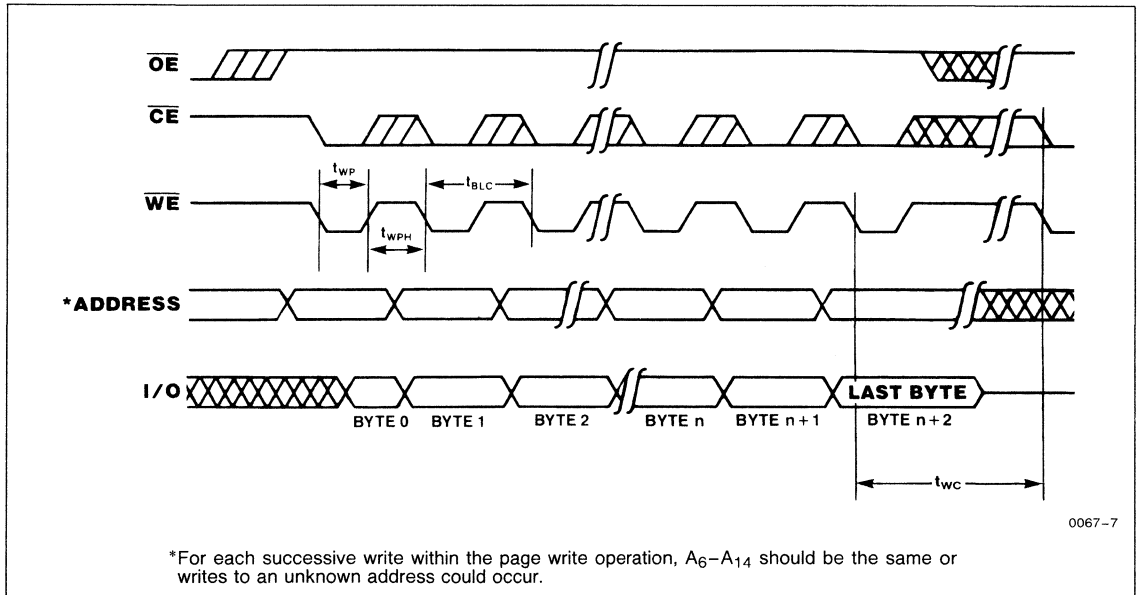
# X28C256, X28C256I

## CE Controlled Write Cycle



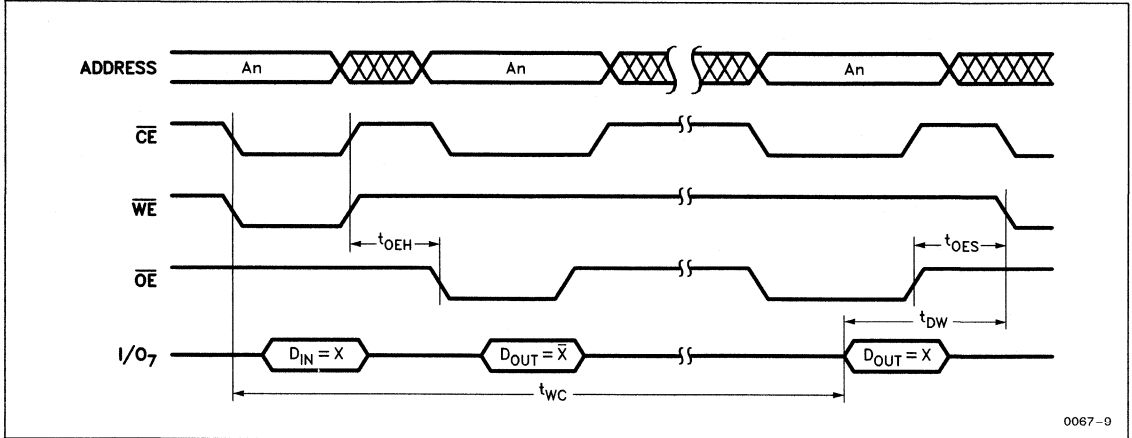
3

## Page Write Cycle

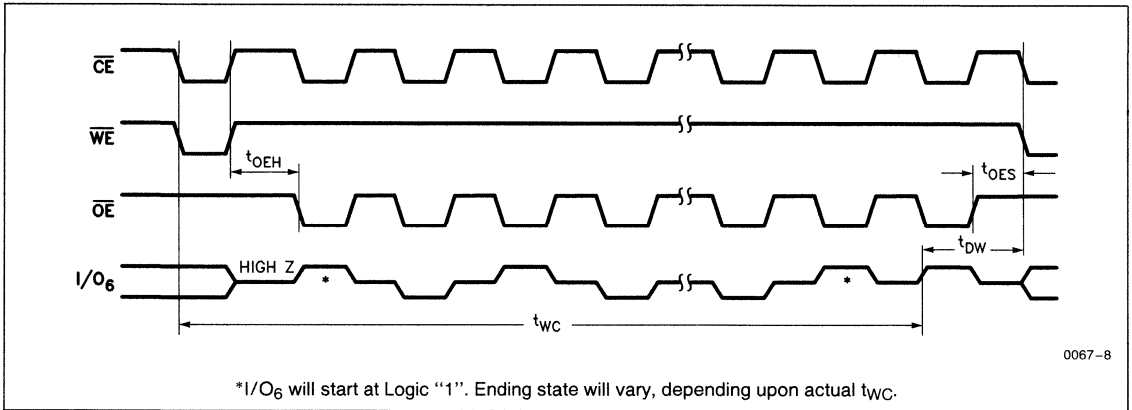


# X28C256, X28C256I

## DATA Polling Timing Diagram



## Toggle Bit Timing Diagram



## X28C256, X28C256I

### PIN DESCRIPTIONS

#### Addresses (A<sub>0</sub>–A<sub>14</sub>)

The Address inputs select an 8-bit memory location during a read or write operation.

#### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

#### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

#### Data In/Data Out (I/O<sub>0</sub>–I/O<sub>7</sub>)

Data is written to or read from the X28C256 through the I/O pins.

#### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X28C256.

### DEVICE OPERATION

#### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

#### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X28C256 supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

#### Page Write Operation

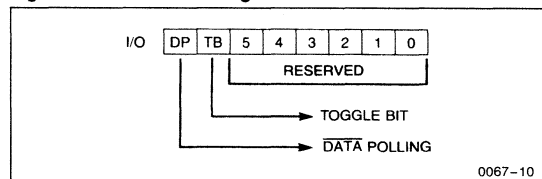
The page write feature of the X28C256 allows the entire memory to be written in 2.5 seconds. Page write allows two to sixty-four bytes of data to be consecutively written to the X28C256 prior to the commencement of the internal programming cycle. The host can fetch data from another location within the system during a page write operation (change the source address), but the page address (A<sub>6</sub> through A<sub>14</sub>) for each subsequent valid write cycle to the part during this operation must be the same as the initial page address.

The page write mode can be initiated during any write operation. Following the initial byte write cycle, the host can write an additional one to sixty-three bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 100  $\mu$ s.

#### Write Operation Status Bits

The X28C256 provides the user two write operation status bits. These can be used to optimize a system write cycle time. The status bits are mapped onto the I/O bus as shown in Figure 1.

Figure 1: Status Bit Assignment



#### $\overline{DATA}$ Polling (I/O<sub>7</sub>)

The X28C256 features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X28C256, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on I/O<sub>7</sub> (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete, I/O<sub>7</sub> will reflect true data. Note: If the X28C256 is in the protected state and an illegal write operation is attempted  $\overline{DATA}$  Polling will not operate.

#### Toggle Bit (I/O<sub>6</sub>)

The X28C256 also provides another method for determining when the internal write cycle is complete. During the internal programming cycle I/O<sub>6</sub> will toggle from one to zero and zero to one on subsequent attempts to read the device. When the internal cycle is complete the toggling will cease and the device will be accessible for additional read or write operations.

# X28C256, X28C256I

## DATA POLLING I/O<sub>7</sub>

Figure 2a: DATA Polling Bus Sequence

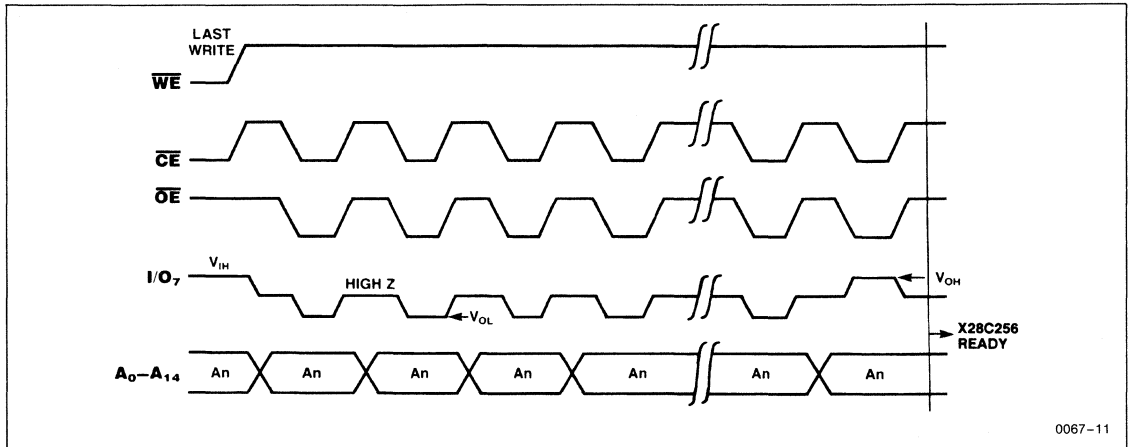
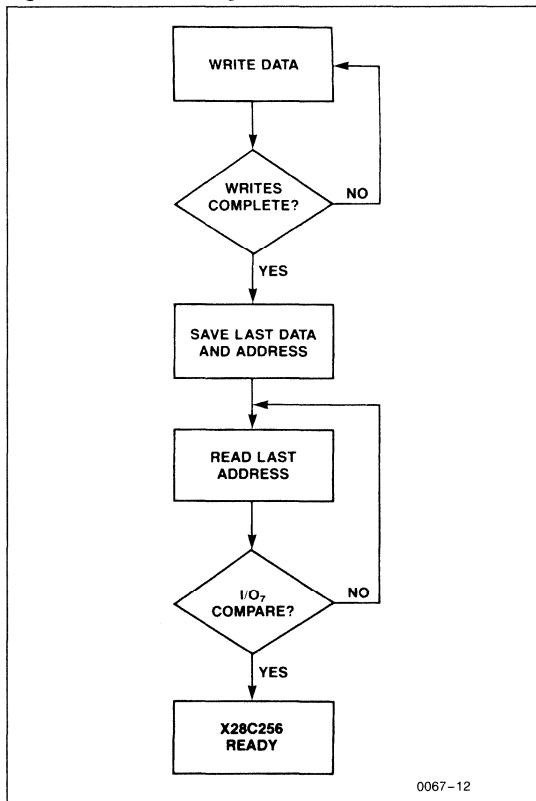


Figure 2b: DATA Polling Software Flow



$\overline{\text{DATA}}$  Polling can effectively halve the time for writing to the X28C256. The timing diagram in Figure 2a illustrates the sequence of events on the bus. The software flow diagram in Figure 2b illustrates one method of implementing the routine.

# X28C256, X28C256I

## THE TOGGLE BIT I/O<sub>6</sub>

Figure 3a: Toggle Bit Bus Sequence

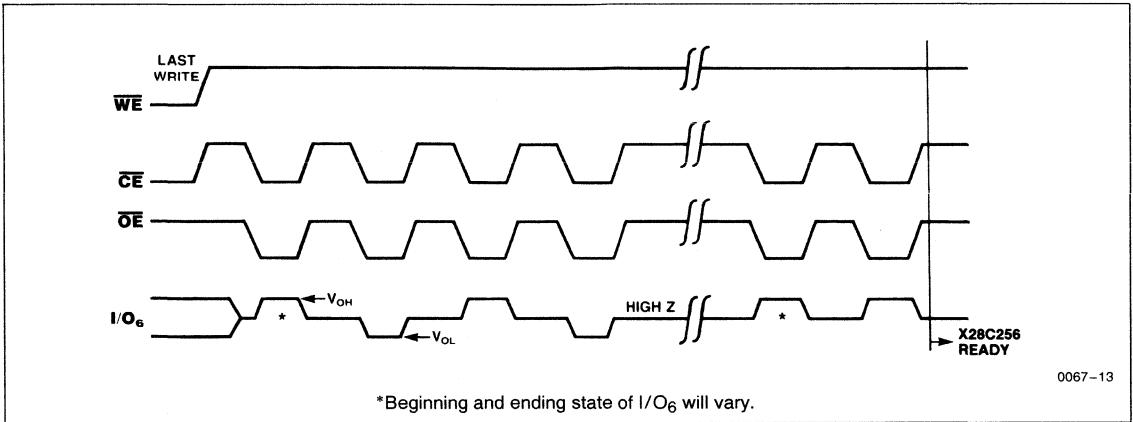
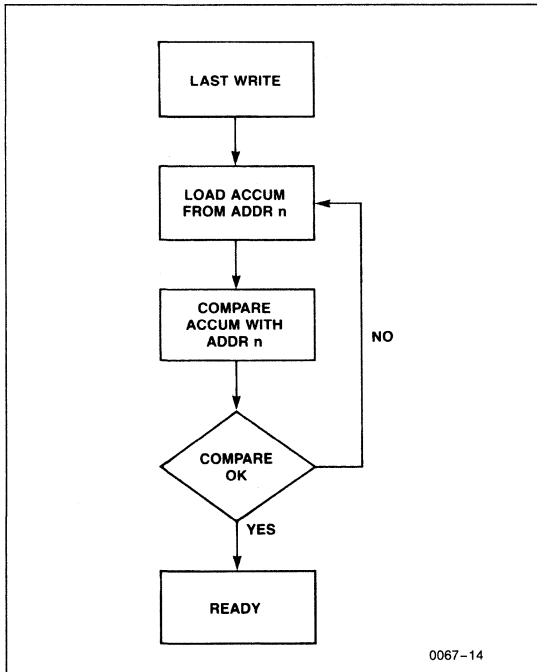


Figure 3b: Toggle Bit Software Flow



The Toggle Bit can eliminate the software housekeeping chore of saving and fetching the last address and data written to a device in order to implement  $\overline{\text{DATA}}$  Polling. This can be especially helpful in an array comprised of multiple X28C256 memories that is frequently updated. The timing diagram in Figure 3a illustrates the sequence of events on the bus. The software flow diagram in Figure 3b illustrates a method for testing the Toggle Bit.

## X28C256, X28C256I

---

### HARDWARE DATA PROTECTION

The X28C256 provides three hardware features (compatible with X2864A) that protect nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse less than 20 ns will not initiate a write cycle.
- Default  $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH, or  $\overline{CE}$  HIGH will prevent an inadvertent write cycle during power-on and power-off, maintaining data integrity.

### SOFTWARE DATA PROTECTION

The X28C256 offers a software controlled data protection feature. The X28C256 is shipped from Xicor with the software data protection NOT ENABLED; that is, the device will be in the standard operating mode. In this mode data should be protected during power-up/-down operations through the use of external circuits. The host would then have open read and write access of the device once  $V_{CC}$  was stable.

The X28C256 can be automatically protected during power-up and power-down without the need for external circuits by employing the software data protection feature. The internal software data protection circuit is enabled after the first write operation utilizing the software algorithm. This circuit is nonvolatile and will remain set for the life of the device unless the reset command is issued.

Once the software protection is enabled, the X28C256 is also protected from inadvertent and accidental writes in the powered-on state. That is, the software algorithm must be issued prior to writing additional data to the device.

### SOFTWARE ALGORITHM

Selecting the software data protection mode requires the host system to precede data write operations by a series of three write operations to three specific addresses. Refer to Figure 4a and 4b for the sequence. The three byte sequence opens the page write window enabling the host to write from one to sixty-four bytes of data.<sup>(5)</sup> Once the page load cycle has been completed, the device will automatically be returned to the data protected state.

**Note:** (5) Once the three byte sequence is issued it must be followed by a valid byte or page write operation.



# X28C256, X28C256I

## SOFTWARE DATA PROTECTION

Figure 4a: Timing Sequence—Byte or Page Write

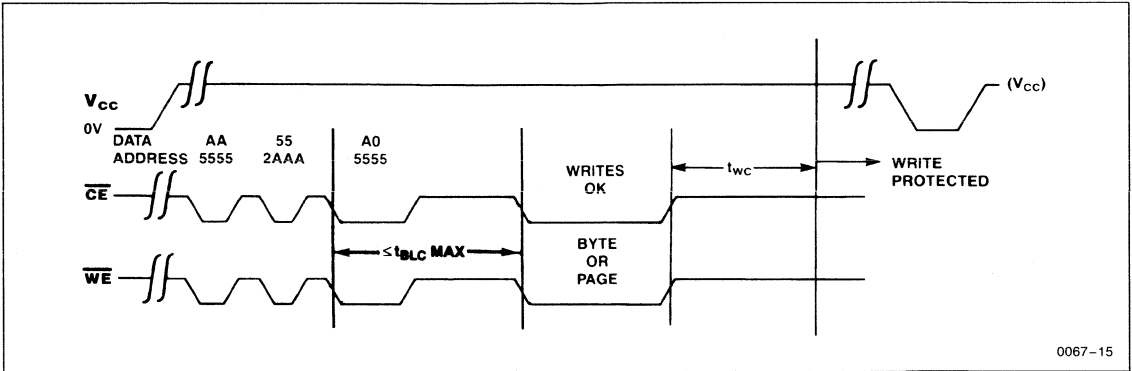
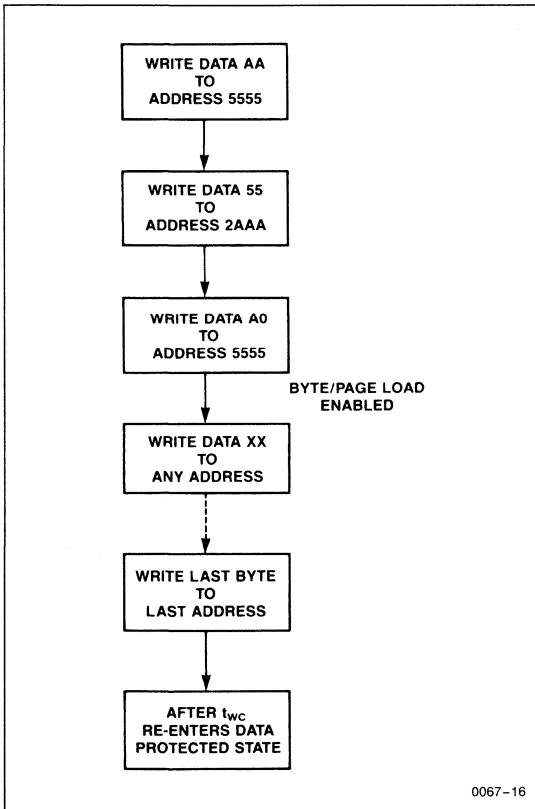


Figure 4b: Write Sequence for Software Data Protection



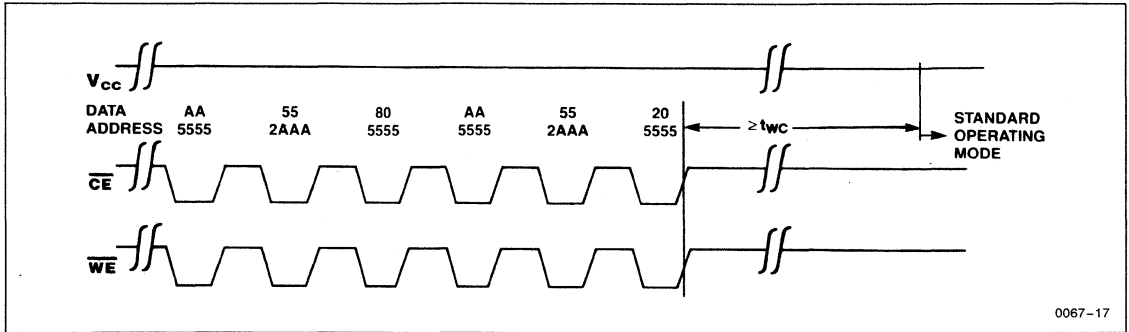
Regardless of whether the device has previously been protected or not, once the software data protected algorithm is used and data has been written, the X28C256 will automatically disable further writes unless another command is issued to cancel it. If no further commands are issued the X28C256 will be write protected during power-down and after any subsequent power-up.

**Note:** Once initiated, the sequence of write operations should not be interrupted.

# X28C256, X28C256I

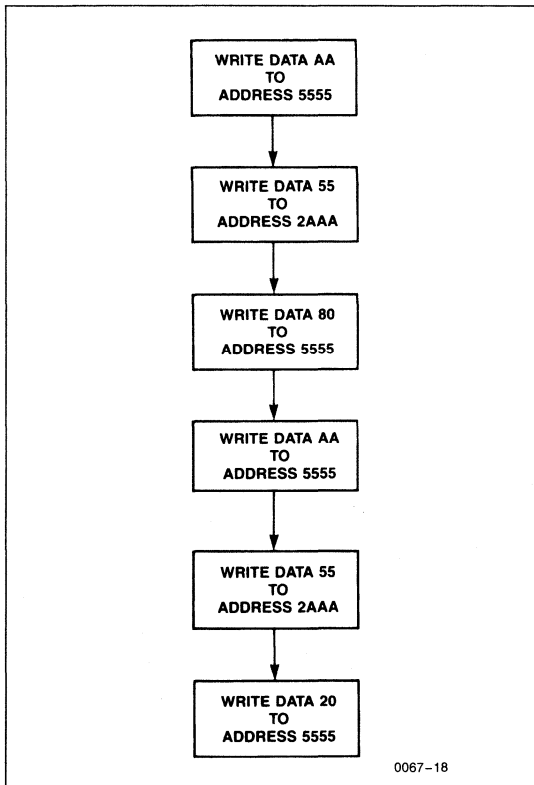
## RESETTING SOFTWARE DATA PROTECTION

Figure 5a: Reset Software Data Protection Timing Sequence



0067-17

Figure 5b: Software Sequence to Deactivate Software Data Protection



0067-18

In the event the user wants to deactivate the software data protection feature for testing or reprogramming in an E<sup>2</sup>PROM programmer, the following six step algorithm will reset the internal protection circuit. After  $t_{WC}$ , the X28C256 will be in standard operating mode.

**Note: Once initiated, the sequence of write operations should not be interrupted.**

# X28C256, X28C256I

## SYSTEM CONSIDERATIONS

Because the X28C256 is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

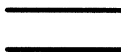




Because the X28C256 has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

3

**SYMBOL TABLE**

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care: Changes Allowed	Changing: State Not Known
	N/A	Center Line is High Impedance

---

## NOTES

## Electrically Erasable PROM

### FEATURES

- **LOW Power CMOS**
  - 60 mA Active Current Max.
  - 200  $\mu$ A Standby Current Max.
- **Fast Write Cycle Times**
  - 64-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 2.5 Sec. Typical
  - Effective Byte Write Cycle Time: 78  $\mu$ s Typical
- **Software Data Protection**
- **End of Write Detection**
  - DATA Polling
  - Toggle Bit
- **Simple Byte and Page Write**
  - Single TTL Compatible  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **Upward Compatible with X2864A**
- **JEDEC Approved Byte-Wide Pinout**

### DESCRIPTION

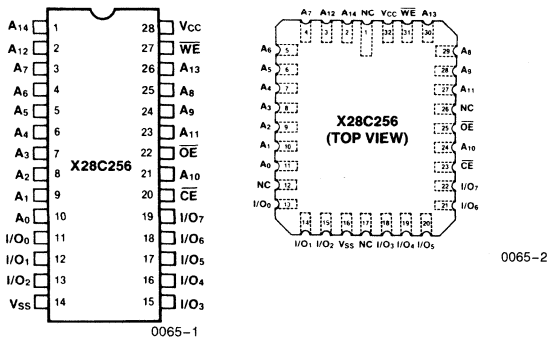
The Xicor X28C256 is a 32K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, floating gate CMOS technology. Like all Xicor programmable non-volatile memories the X28C256 is a 5V only device. The X28C256 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard RAMs.

The X28C256 supports a 64-byte page write operation, effectively providing a 78  $\mu$ s/byte write cycle and enabling the entire memory to be typically written in less than 2.5 seconds. The X28C256 also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle. In addition, the X28C256 includes a user-optional software data protection mode that further enhances Xicor's hardware write protect capability.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

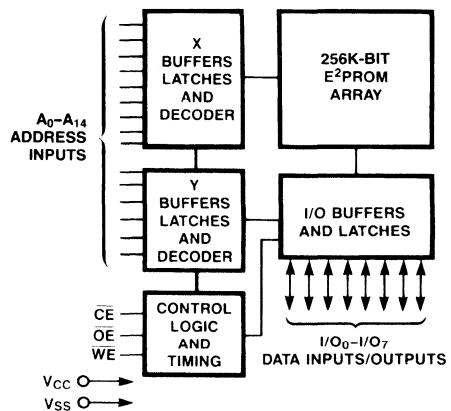
### PIN CONFIGURATIONS



### PIN NAMES

A <sub>0</sub> -A <sub>14</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



# X28C256M

## ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on any Pin with Respect to Ground	-1.0V to +7V
D.C. Output Current	5 mA
Lead Temperature (Soldering, 10 Seconds)	300°C

## \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ.(1)	Max.		
$I_{CC}$	$V_{CC}$ Current (Active) (TTL Inputs)			60	mA	$\overline{CE} = \overline{OE} = V_{IL}$ , $\overline{WE} = V_{IH}$ All I/O's = Open Address Inputs = TTL Levels @ $f = 5\text{ MHz}$
$I_{SB1}$	$V_{CC}$ Current (Standby) (TTL Inputs)			2	mA	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{IH}$
$I_{SB2}$	$V_{CC}$ Current (Standby) (CMOS Inputs)		100	200	$\mu\text{A}$	$\overline{CE} = V_{IH}$ , $\overline{OE} = V_{IL}$ All I/O's = Open Other Inputs = $V_{CC}$
$I_{LI}$	Input Leakage Current			10	$\mu\text{A}$	$V_{IN} = \text{GND to } V_{CC}$
$I_{LO}$	Output Leakage Current			10	$\mu\text{A}$	$V_{OUT} = \text{GND to } V_{CC}$ , $\overline{CE} = V_{IH}$
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{OL}$	Output Low Voltage			0.4	V	$I_{OL} = 2.1\text{ mA}$
$V_{OH}$	Output High Voltage	2.4			V	$I_{OH} = -400\ \mu\text{A}$

## TYPICAL POWER-UP TIMING

Symbol	Parameter	Typ.(1)	Units
$t_{PUR}^{(2)}$	Power-Up to Read Operation	100	$\mu\text{s}$
$t_{PUW}^{(2)}$	Power-Up to Write Operation	5	ms

**CAPACITANCE**  $T_A = 25^\circ\text{C}$ ,  $f = 1.0\text{ MHz}$ ,  $V_{CC} = 5\text{V}$

Symbol	Test	Max.	Units	Conditions
$C_{I/O}^{(2)}$	Input/Output Capacitance	10	pF	$V_{I/O} = 0\text{V}$
$C_{IN}^{(2)}$	Input Capacitance	6	pF	$V_{IN} = 0\text{V}$

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input and Output Timing Levels	1.5V
Output Load	1 TTL Gate and $C_L = 100\text{ pF}$

## MODE SELECTION

$\overline{CE}$	$\overline{OE}$	$\overline{WE}$	Mode	I/O	Power
L	L	H	Read	$D_{OUT}$	Active
L	H	L	Write	$D_{IN}$	Active
H	X	X	Standby and Write Inhibit	High Z	Standby
X	L	X	Write Inhibit	—	—
X	X	H	Write Inhibit	—	—

**Notes:** (1) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(2) This parameter is periodically sampled and not 100% tested.

# X28C256M

## A.C. CHARACTERISTICS

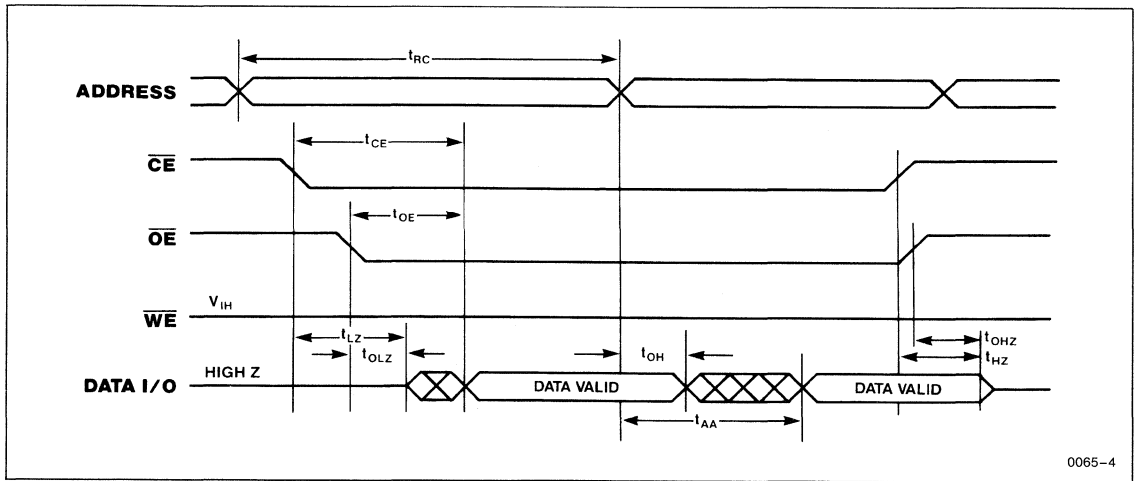
$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

### Read Cycle Limits

Symbol	Parameter	X28C256M-25		X28C256M		X28C256M-35		Units
		Min.	Max.	Min.	Max.	Min.	Max.	
$t_{RC}$	Read Cycle Time	250		300		350		ns
$t_{CE}$	Chip Enable Access Time		250		300		350	ns
$t_{AA}$	Address Access Time		250		300		350	ns
$t_{OE}$	Output Enable Access Time		100		100		100	ns
$t_{LZ}$	$\overline{CE}$ Low to Active Output	0		0		0		ns
$t_{OLZ}$	$\overline{OE}$ Low to Active Output	0		0		0		ns
$t_{HZ}^{(3)}$	$\overline{CE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OHZ}^{(3)}$	$\overline{OE}$ High to High Z Output	0	50	0	50	0	50	ns
$t_{OH}$	Output Hold from Address Change	0		0		0		ns

3

### Read Cycle



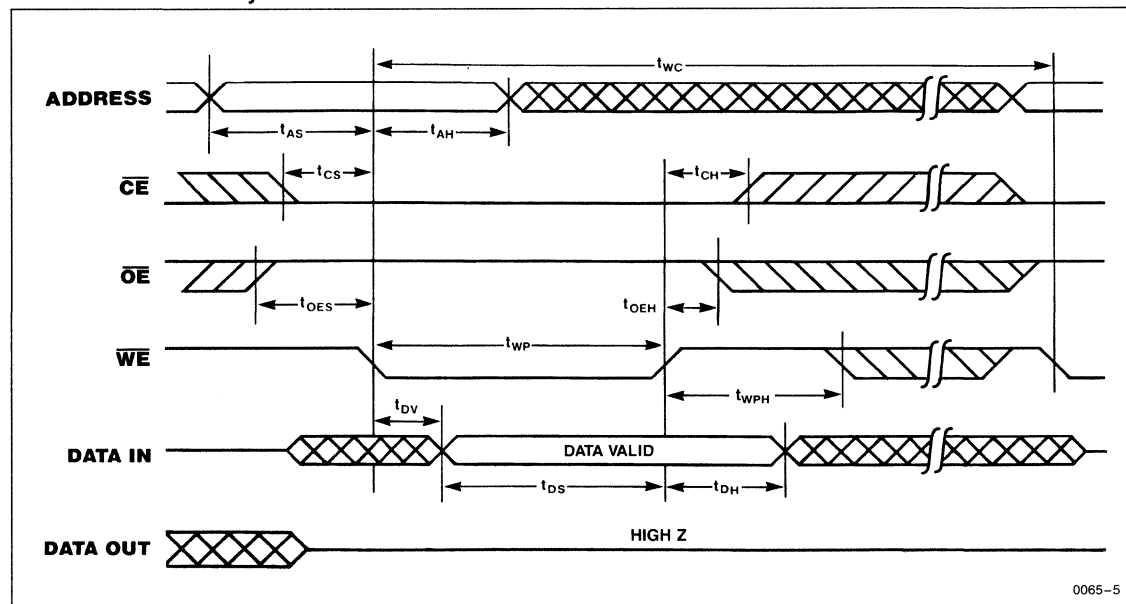
**Note:** (3)  $t_{HZ}$  and  $t_{OHZ}$  are measured from the point when  $\overline{CE}$  or  $\overline{OE}$  return high (whichever occurs first) to the time when the outputs are no longer driven.

# X28C256M

## Write Cycle Limits

Symbol	Parameter	Min.	Typ.(4)	Max.	Units
$t_{WC}$	Write Cycle Time		5	10	ms
$t_{AS}$	Address Setup Time	0			ns
$t_{AH}$	Address Hold Time	150			ns
$t_{CS}$	Write Setup Time	0			ns
$t_{CH}$	Write Hold Time	0			ns
$t_{CW}$	$\overline{CE}$ Pulse Width	100			ns
$t_{OES}$	$\overline{OE}$ High Setup Time	10			ns
$t_{OEH}$	$\overline{OE}$ High Hold Time	10			ns
$t_{WP}$	$\overline{WE}$ Pulse Width	100			ns
$t_{WPH}$	$\overline{WE}$ High Recovery	1			$\mu$ s
$t_{DV}$	Data Valid			1	$\mu$ s
$t_{DS}$	Data Setup	50			ns
$t_{DH}$	Data Hold	10			ns
$t_{DW}$	Delay to Next Write	10			$\mu$ s
$t_{BLC}$	Byte Load Cycle	1		100	$\mu$ s

## $\overline{WE}$ Controlled Write Cycle



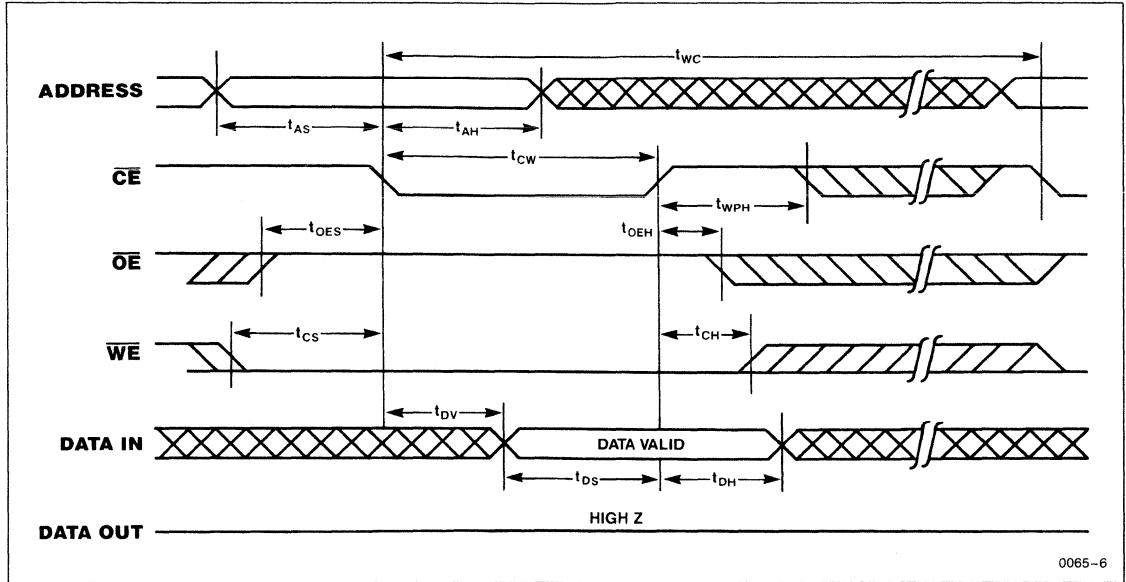
0065-5

Note: (4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.



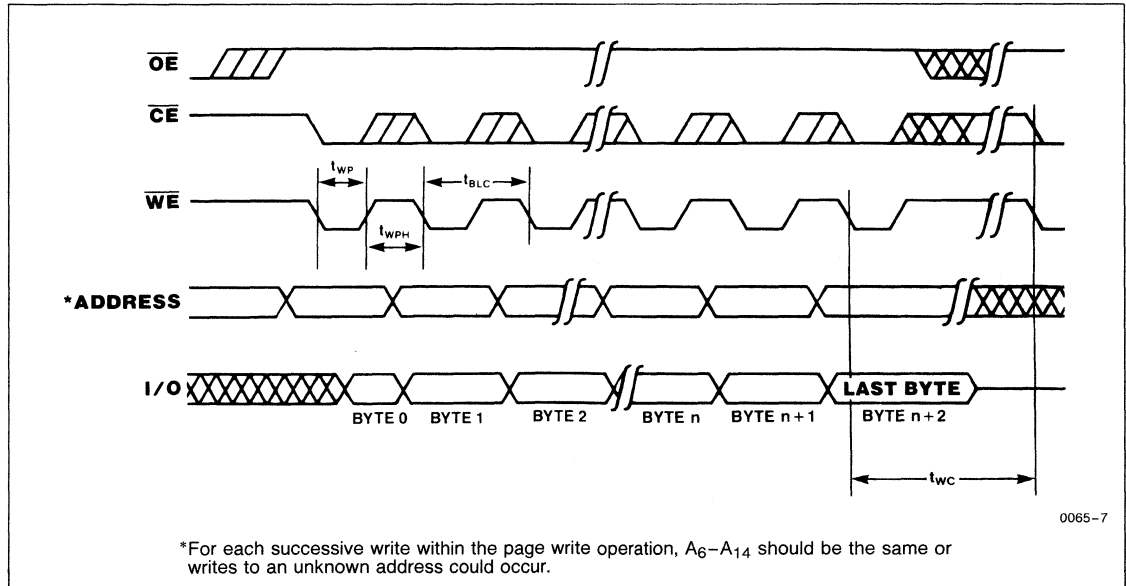
# X28C256M

## CE Controlled Write Cycle



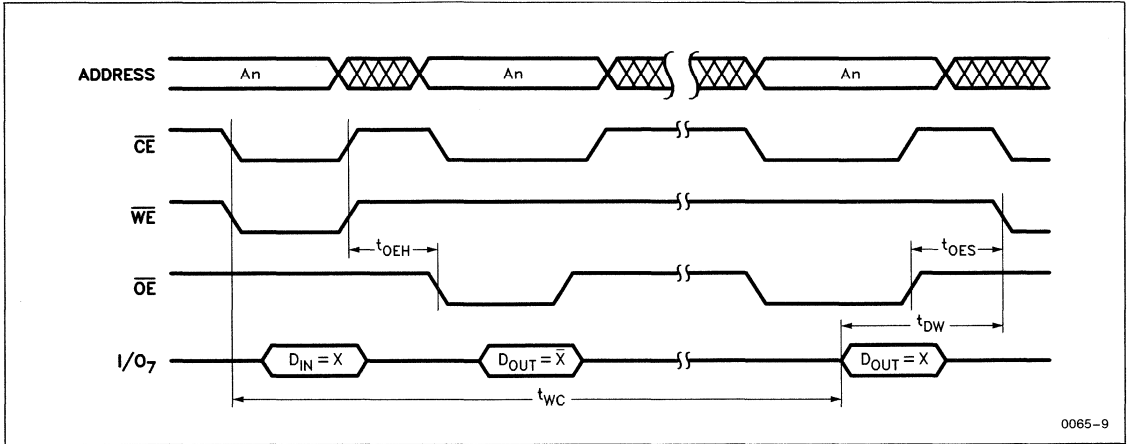
3

## Page Write Cycle

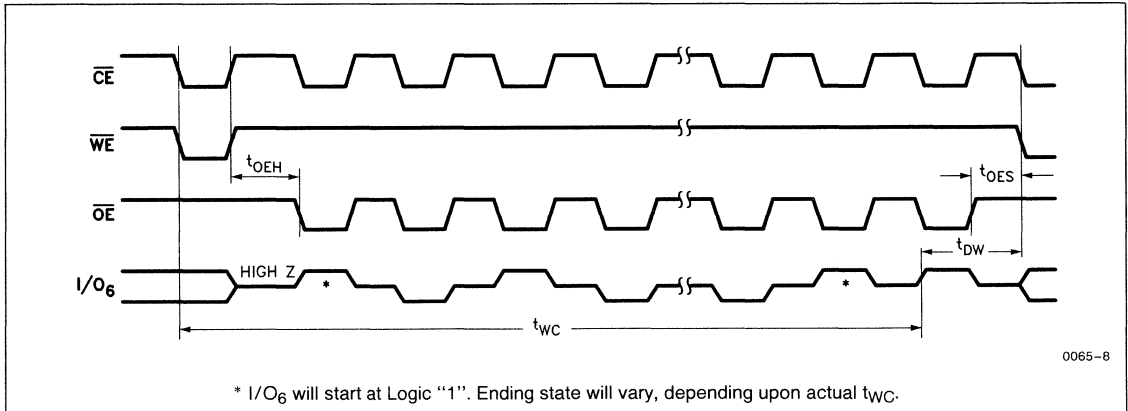


# X28C256M

## DATA Polling Timing Diagram



## Toggle Bit Timing Diagram



# X28C256M

## PIN DESCRIPTIONS

### Addresses ( $A_0$ – $A_{14}$ )

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out ( $I/O_0$ – $I/O_7$ )

Data is written to or read from the X28C256 through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X28C256.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X28C256 supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

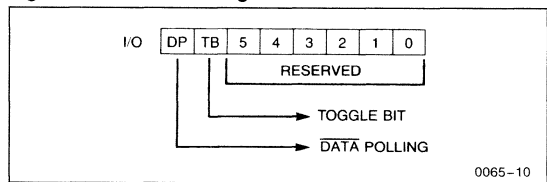
The page write feature of the X28C256 allows the entire memory to be written in 2.5 seconds. Page write allows two to sixty-four bytes of data to be consecutively written to the X28C256 prior to the commencement of the internal programming cycle. The host can fetch data from another location within the system during a page write operation (change the source address), but the page address ( $A_6$  through  $A_{14}$ ) for each subsequent valid write cycle to the part during this operation must be the same as the initial page address.

The page write mode can be initiated during any write operation. Following the initial byte write cycle, the host can write an additional one to sixty-three bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 100  $\mu$ s.

### Write Operation Status Bits

The X28C256 provides the user two write operation status bits. These can be used to optimize a system write cycle time. The status bits are mapped onto the I/O bus as shown in Figure 1.

Figure 1: Status Bit Assignment



### DATA Polling ( $I/O_7$ )

The X28C256 features  $\overline{DATA}$  Polling as a method to indicate to the host system that the byte write or page write cycle has completed.  $\overline{DATA}$  Polling allows a simple bit test operation to determine the status of the X28C256, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on  $I/O_7$  (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete,  $I/O_7$  will reflect true data. Note: If the X28C256 is in the protected state and an illegal write operation is attempted  $\overline{DATA}$  Polling will not operate.

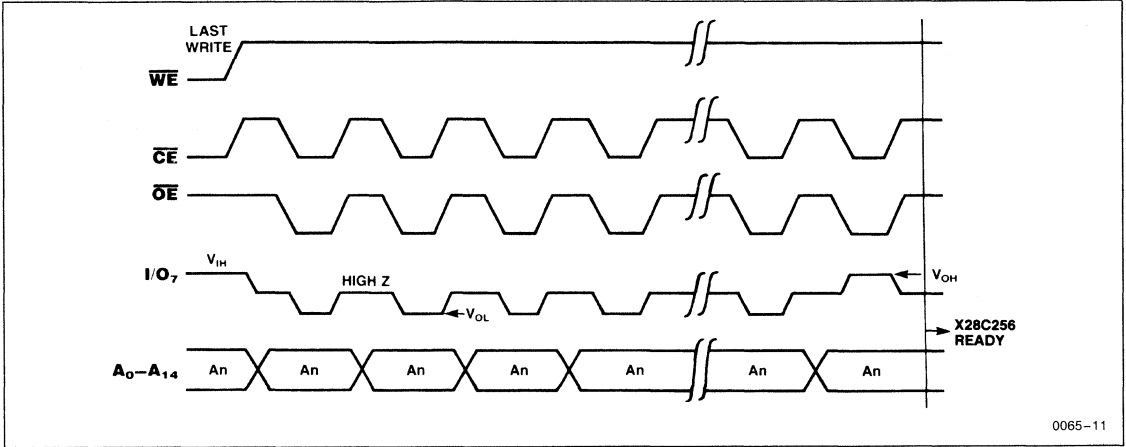
### Toggle Bit ( $I/O_6$ )

The X28C256 also provides another method for determining when the internal write cycle is complete. During the internal programming cycle  $I/O_6$  will toggle from one to zero and zero to one on subsequent attempts to read the device. When the internal cycle is complete the toggling will cease and the device will be accessible for additional read or write operations.

# X28C256M

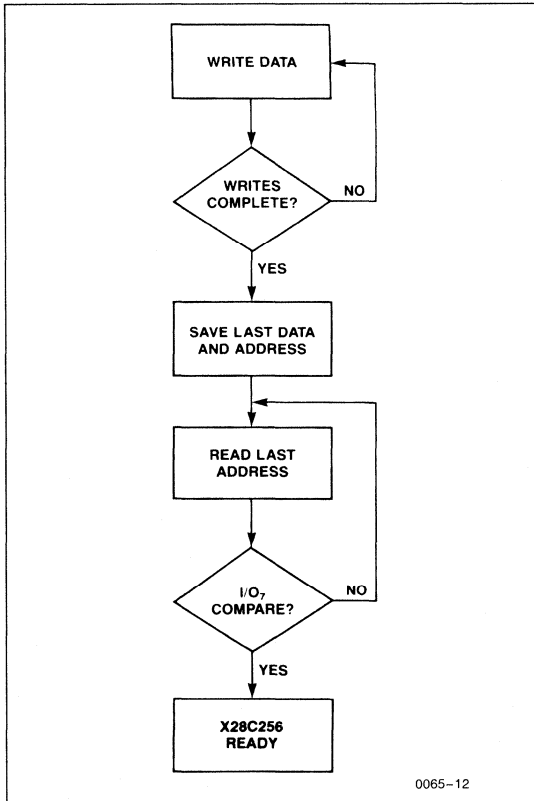
## DATA POLLING I/O<sub>7</sub>

Figure 2a: DATA Polling Bus Sequence



0065-11

Figure 2b: DATA Polling Software Flow



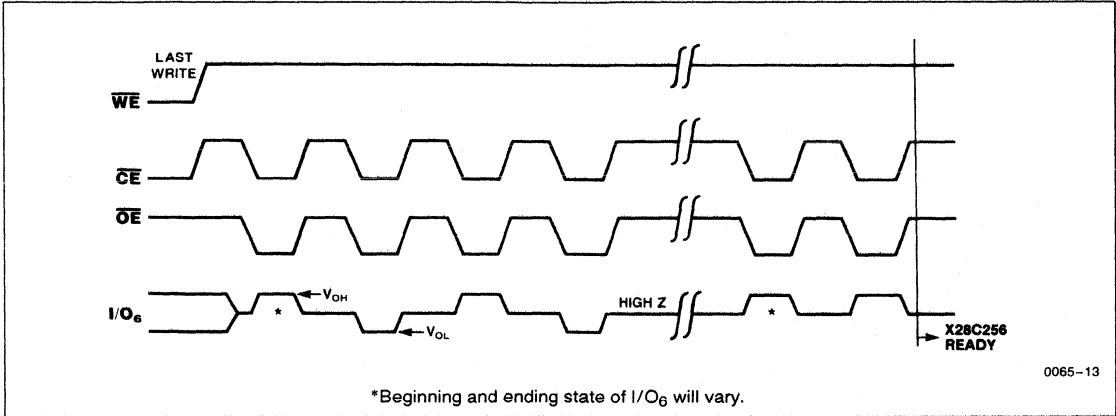
0065-12

DATA Polling can effectively halve the time for writing to the X28C256. The timing diagram in Figure 2a illustrates the sequence of events on the bus. The software flow diagram in Figure 2b illustrates one method of implementing the routine.

# X28C256M

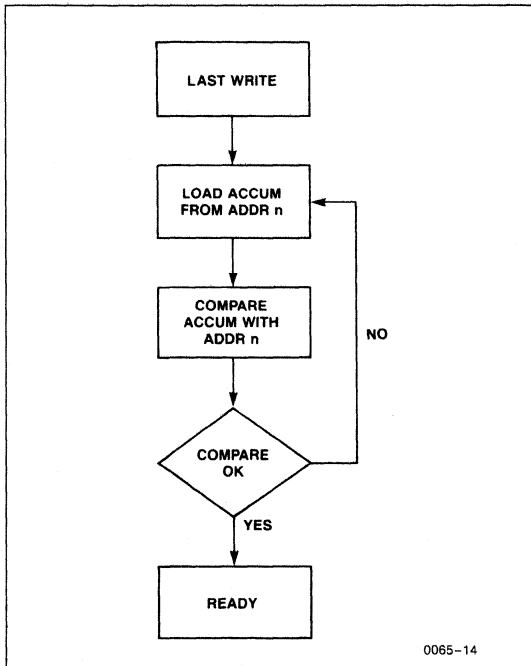
## THE TOGGLE BIT I/O<sub>6</sub>

Figure 3a: Toggle Bit Bus Sequence



3

Figure 3b: Toggle Bit Software Flow



The Toggle Bit can eliminate the software housekeeping chore of saving and fetching the last address and data written to a device in order to implement DATA Polling. This can be especially helpful in an array comprised of multiple X28C256 memories that is frequently updated. The timing diagram in Figure 3a illustrates the sequence of events on the bus. The software flow diagram in Figure 3b illustrates a method for testing the Toggle Bit.

## X28C256M

---

### HARDWARE DATA PROTECTION

The X28C256 provides three hardware features (compatible with X2864A) that protect nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse less than 20 ns will not initiate a write cycle.
- Default  $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ , typically.
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH, or  $\overline{CE}$  HIGH will prevent an inadvertent write cycle during power-on and power-off, maintaining data integrity.

### SOFTWARE DATA PROTECTION

The X28C256 offers a software controlled data protection feature. The X28C256 is shipped from Xicor with the software data protection NOT ENABLED; that is, the device will be in the standard operating mode. In this mode data should be protected during power-up/-down operations through the use of external circuits. The host would then have open read and write access of the device once  $V_{CC}$  was stable.

The X28C256 can be automatically protected during power-up and power-down without the need for external circuits by employing the software data protection feature. The internal software data protection circuit is enabled after the first write operation utilizing the software algorithm. This circuit is nonvolatile and will remain set for the life of the device unless the reset command is issued.

Once the software protection is enabled, the X28C256 is also protected from inadvertent and accidental writes in the powered-on state. That is, the software algorithm must be issued prior to writing additional data to the device.

### SOFTWARE ALGORITHM

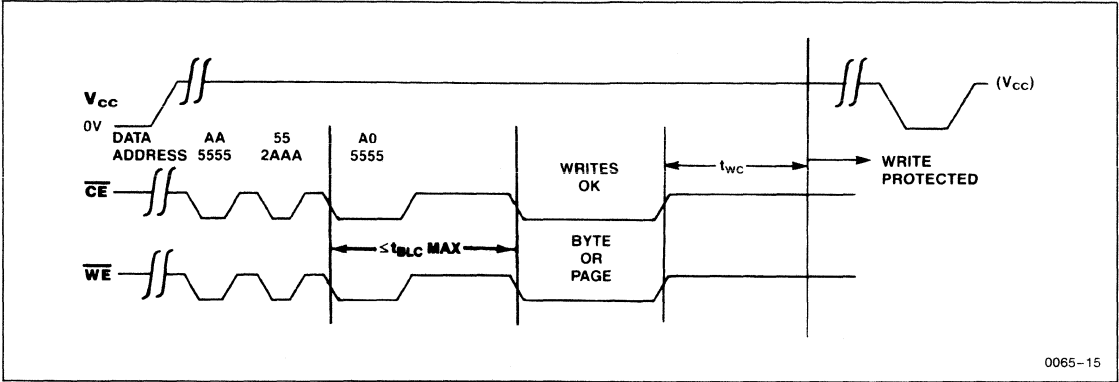
Selecting the software data protection mode requires the host system to precede data write operations by a series of three write operations to three specific addresses. Refer to Figure 4a and 4b for the sequence. The three byte sequence opens the page write window enabling the host to write from one to sixty-four bytes of data.<sup>(5)</sup> Once the page load cycle has been completed, the device will automatically be returned to the data protected state.

**Note:** (5) Once the three byte sequence is issued it must be followed by a valid byte or page write operation.

# X28C256M

## SOFTWARE DATA PROTECTION

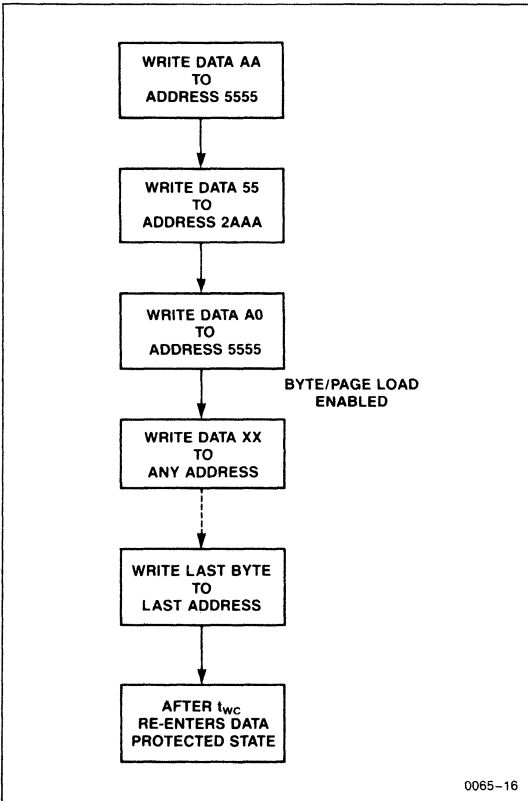
Figure 4a: Timing Sequence—Byte or Page Write



0065-15

3

Figure 4b: Write Sequence for Software Data Protection



0065-16

Regardless of whether the device has previously been protected or not, once the software data protected algorithm is used and data has been written, the X28C256 will automatically disable further writes unless another command is issued to cancel it. If no further commands are issued the X28C256 will be write protected during power-down and after any subsequent power-up.

**Note:** Once initiated, the sequence of write operations should not be interrupted.

# X28C256M

## RESETTING SOFTWARE DATA PROTECTION

Figure 5a: Reset Software Data Protection Timing Sequence

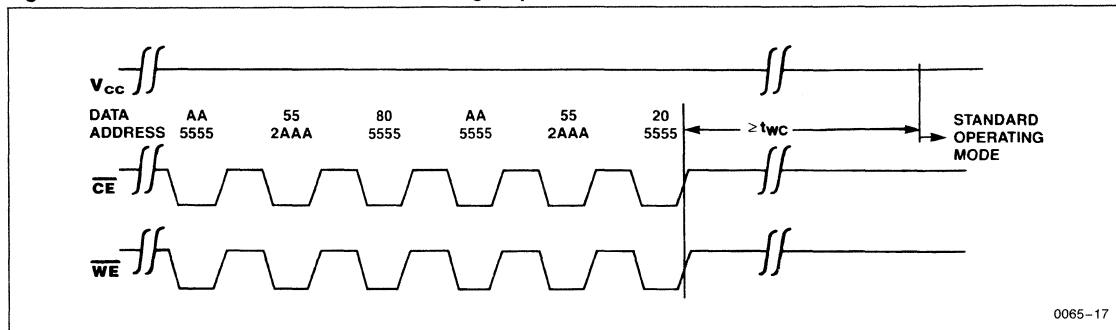
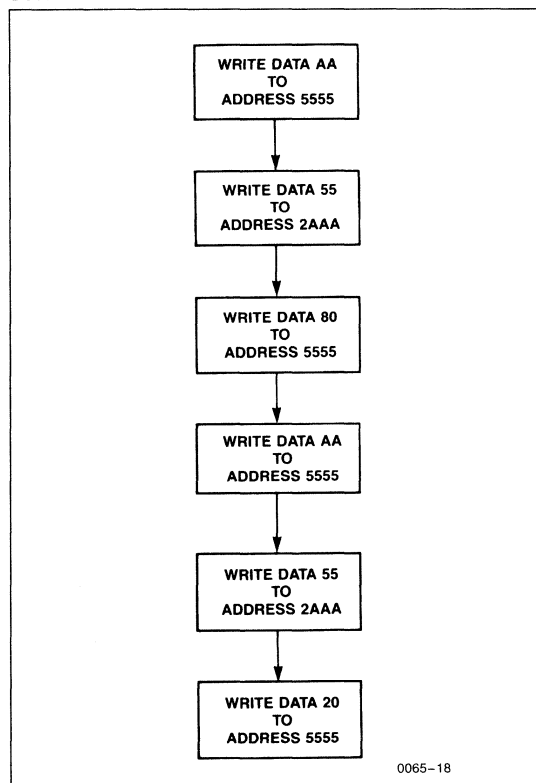


Figure 5b: Software Sequence to Deactivate Software Data Protection



In the event the user wants to deactivate the software data protection feature for testing or reprogramming in an E<sup>2</sup>PROM programmer, the following six step algorithm will reset the internal protection circuit. After  $t_{WC}$ , the X28C256 will be in standard operating mode.

**Note:** Once initiated, the sequence of write operations should not be interrupted.



# X28C256M

## SYSTEM CONSIDERATIONS

Because the X28C256 is frequently used in large memory arrays it is provided with a two line control architecture for both read and write operations. Proper usage can provide the lowest possible power dissipation and eliminate the possibility of contention where multiple I/O pins share the same bus.

To gain the most benefit it is recommended that  $\overline{CE}$  be decoded from the address bus and be used as the primary device selection input. Both  $\overline{OE}$  and  $\overline{WE}$  would then be common among all devices in the array. For a read operation this assures that all deselected devices are in their standby mode and that only the selected device(s) is outputting data on the bus.

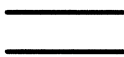




Because the X28C256 has two power modes, standby and active, proper decoupling of the memory array is of

prime concern. Enabling  $\overline{CE}$  will cause transient current spikes. The magnitude of these spikes is dependent on the output capacitive loading of the I/Os. Therefore, the larger the array sharing a common bus, the larger the transient spikes. The voltage peaks associated with the current transients can be suppressed by the proper selection and placement of decoupling capacitors. As a minimum, it is recommended that a 0.1  $\mu\text{F}$  high frequency ceramic capacitor be used between  $V_{CC}$  and GND at each device. Depending on the size of the array, the value of the capacitor may have to be larger.

In addition, it is recommended that a 4.7  $\mu\text{F}$  electrolytic bulk capacitor be placed between  $V_{CC}$  and GND for each eight devices employed in the array. This bulk capacitor is employed to overcome the voltage droop caused by the inductive effects of the PC board traces.

3

## SYMBOL TABLE

WAVEFORM	INPUTS	OUTPUTS
	Must be steady	Will be steady
	May change from Low to High	Will change from Low to High
	May change from High to Low	Will change from High to Low
	Don't Care : Changes Allowed	Changing : State Not Known
	N/A	Center Line is High Impedance

---

## NOTES

1M

Commercial

X28C010

128K x 8 Bit

## Electrically Erasable PROM

### FEATURES

- **200 ns Access Time**
- **LOW Power CMOS**
  - 80 mA Active Current Typical
  - 500  $\mu$ A Standby Current Typical
- **Fast Write Cycle Times**
  - 128-Byte Page Write Operation
  - Byte or Page Write Cycle: 5 ms Typical
  - Complete Memory Rewrite: 5 Sec. Typical
  - Effective Byte Write Cycle Time: 39  $\mu$ s Typical
- **Software Data Protection**
- **End of Write Detection**
  - DATA Polling
  - Toggle Bit
- **Simple Byte and Page Write**
  - Single TTL Compatible  $\overline{WE}$  Signal
  - Internally Latched Address and Data
  - Automatic Write Timing
- **JEDEC Approved Byte-Wide Pinout**

### DESCRIPTION

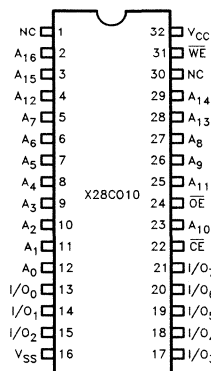
The Xicor X28C010 is a 128K x 8 E<sup>2</sup>PROM, fabricated with Xicor's proprietary, high performance, floating gate CMOS technology. Like all Xicor programmable non-volatile memories the X28C010 is a 5V only device. The X28C010 features the JEDEC approved pinout for byte-wide memories, compatible with industry standard EPROMs.

The X28C010 supports a 128-byte page write operation, effectively providing a 39  $\mu$ s/byte write cycle and enabling the entire memory to be typically written in less than 5 seconds. The X28C010 also features  $\overline{DATA}$  Polling, a system software support scheme used to indicate the early completion of a write cycle. In addition, the X28C010 includes a user-optional software data protection mode that further enhances Xicor's hardware write protect capability.

Xicor E<sup>2</sup>PROMs are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 10 years.

3

### PIN CONFIGURATION

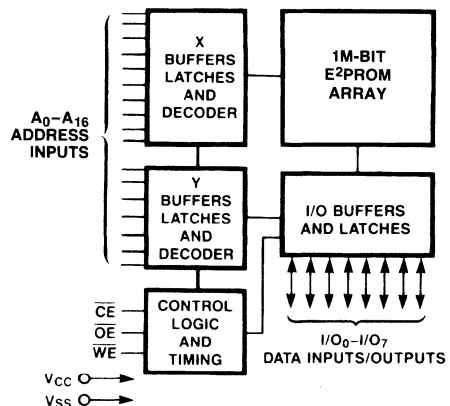


0084-1

### PIN NAMES

A <sub>0</sub> -A <sub>16</sub>	Address Inputs
I/O <sub>0</sub> -I/O <sub>7</sub>	Data Input/Output
$\overline{WE}$	Write Enable
$\overline{CE}$	Chip Enable
$\overline{OE}$	Output Enable
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

### FUNCTIONAL DIAGRAM



0084-2

# X28C010

## PIN DESCRIPTIONS

### Addresses (A<sub>0</sub>–A<sub>16</sub>)

The Address inputs select an 8-bit memory location during a read or write operation.

### Chip Enable ( $\overline{CE}$ )

The Chip Enable input must be LOW to enable all read/write operations. When  $\overline{CE}$  is HIGH, power consumption is reduced.

### Output Enable ( $\overline{OE}$ )

The Output Enable input controls the data output buffers and is used to initiate read operations.

### Data In/Data Out (I/O<sub>0</sub>–I/O<sub>7</sub>)

Data is written to or read from the X28C010 through the I/O pins.

### Write Enable ( $\overline{WE}$ )

The Write Enable input controls the writing of data to the X28C010.

## DEVICE OPERATION

### Read

Read operations are initiated by both  $\overline{OE}$  and  $\overline{CE}$  LOW. The read operation is terminated by either  $\overline{CE}$  or  $\overline{OE}$  returning HIGH. This 2-line control architecture eliminates bus contention in a system environment. The data bus will be in a high impedance state when either  $\overline{OE}$  or  $\overline{CE}$  is HIGH.

### Write

Write operations are initiated when both  $\overline{CE}$  and  $\overline{WE}$  are LOW and  $\overline{OE}$  is HIGH. The X28C010 supports both a  $\overline{CE}$  and  $\overline{WE}$  controlled write cycle. That is, the address is latched by the falling edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs last. Similarly, the data is latched internally by the rising edge of either  $\overline{CE}$  or  $\overline{WE}$ , whichever occurs first. A byte write operation, once initiated, will automatically continue to completion, typically within 5 ms.

### Page Write Operation

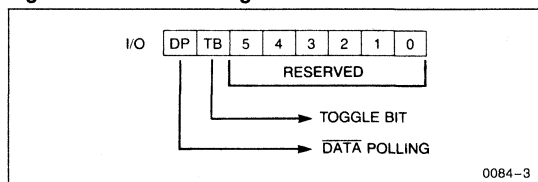
The page write feature of the X28C010 allows the entire memory to be written in 5 seconds. Page write allows two to one hundred twenty-eight bytes of data to be consecutively written to the X28C010 prior to the commencement of the internal programming cycle. The host can fetch data from another location within the system during a page write operation (change the source address), but the page address (A<sub>7</sub> through A<sub>16</sub>) for each subsequent valid write cycle to the part during this operation must be the same as the initial page address.

The page write mode can be initiated during any write operation. Following the initial byte write cycle, the host can write an additional one to one hundred twenty-seven bytes in the same manner as the first byte was written. Each successive byte load cycle, started by the  $\overline{WE}$  HIGH to LOW transition, must begin within 100  $\mu$ s of the falling edge of the preceding  $\overline{WE}$ . If a subsequent  $\overline{WE}$  HIGH to LOW transition is not detected within 100  $\mu$ s, the internal automatic programming cycle will commence. There is no page write window limitation. Effectively the page write window is infinitely wide, so long as the host continues to access the device within the byte load cycle time of 100  $\mu$ s.

### Write Operation Status Bits

The X28C010 provides the user two write operation status bits. These can be used to optimize a system write cycle time. The status bits are mapped onto the I/O bus as shown in Figure 1.

Figure 1: Status Bit Assignment



### DATA Polling (I/O<sub>7</sub>)

The X28C010 features DATA Polling as a method to indicate to the host system that the byte write or page write cycle has completed. DATA Polling allows a simple bit test operation to determine the status of the X28C010, eliminating additional interrupt inputs or external hardware. During the internal programming cycle, any attempt to read the last byte written will produce the complement of that data on I/O<sub>7</sub> (i.e., write data = 0xxx xxxx, read data = 1xxx xxxx). Once the programming cycle is complete, I/O<sub>7</sub> will reflect true data. Note: If the X28C010 is in the protected state and an illegal write operation is attempted DATA Polling will not operate.

### Toggle Bit (I/O<sub>6</sub>)

The X28C010 also provides another method for determining when the internal write cycle is complete. During the internal programming cycle I/O<sub>6</sub> will toggle from one to zero and zero to one on subsequent attempts to read the device. When the internal cycle is complete the toggling will cease and the device will be accessible for additional read or write operations.

## X28C010

---

### HARDWARE DATA PROTECTION

The X28C010 provides three hardware features that protect nonvolatile data from inadvertent writes.

- Noise Protection—A  $\overline{WE}$  pulse less than 20 ns will not initiate a write cycle.
- Default  $V_{CC}$  Sense—All functions are inhibited when  $V_{CC}$  is  $\leq 3V$ .
- Write Inhibit—Holding either  $\overline{OE}$  LOW,  $\overline{WE}$  HIGH, or  $\overline{CE}$  HIGH will prevent an inadvertent write cycle during power-on and power-off, maintaining data integrity.

### SOFTWARE DATA PROTECTION

The X28C010 offers a software controlled data protection feature. The X28C010 is shipped from Xicor with the software data protection NOT ENABLED; that is, the device will be in the standard operating mode. In this mode data should be protected during power-up/-down operations through the use of external circuits. The host would then have open read and write access of the device once  $V_{CC}$  was stable.

The X28C010 can be automatically protected during power-up and power-down without the need for external circuits by employing the software data protection feature. The internal software data protection circuit is enabled after the first write operation utilizing the software algorithm. This circuit is nonvolatile and will remain set for the life of the device unless the reset command is issued.

Once the software protection is enabled, the X28C010 is also protected from inadvertent and accidental writes in the powered-on state. That is, the software algorithm must be issued prior to writing additional data to the device.

### SOFTWARE ALGORITHM

Selecting the software data protection mode requires the host system to precede data write operations by a series of three write operations to three specific addresses. The three byte sequence opens the page write window enabling the host to write from one to one hundred twenty-eight bytes of data. Once the page load cycle has been completed, the device will automatically be returned to the data protected state.

3

---

## NOTES

X9MME, X9MMEI .....	4-1
X9MMEM .....	4-7

**NOVRAM\* Data Sheets**

**1**

**Serial I/O Data Sheets**

**2**

**E<sup>2</sup>PROM Data Sheets**

**3**



**E<sup>2</sup>POT™ Digitally Controlled  
Potentiometer Data Sheets**

**4**





**Commercial  
Industrial**

**X9MME  
X9MME1**

## E2POT™ Digitally Controlled Potentiometer

### FEATURES

- Solid State Reliability
- Single Chip MOS Implementation
- Three Wire TTL Control
- Operates From Standard 5V Supply
- Wide Analog Voltage Range  $\pm 5V$  Min.
- 99 Resistive Elements
  - Temperature Compensated
  - $\pm 20\%$  End to End Resistance Range
- 100 Wiper Tap Points
  - Wiper Position Digitally Controlled
  - Wiper Position Stored in Nonvolatile Memory Then Automatically Recalled on Power-Up
- 100 Year Wiper Position Retention
- 8 Pin Mini-DIP Package

### DESCRIPTION

The Xicor X9MME is a solid state nonvolatile potentiometer, packaged in an 8 pin mini-DIP and is ideal for digitally controlled resistance trimming.

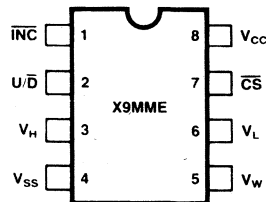
The X9MME is a resistor array composed of 99 resistive elements. Between each element and at either end are tap points accessible to the wiper element. The position of the wiper element on the array is controlled by the  $\overline{CS}$ ,  $U/\overline{D}$ , and  $\overline{INC}$  inputs. The position of the wiper can be stored in nonvolatile memory and is recalled upon a subsequent power-up.

The resolution of the X9MME is equal to the maximum resistance value divided by 99. As an example; for the X9503 (50 K $\Omega$ ) each tap point represents 505 $\Omega$ .

Xicor E2 products are designed and tested for applications requiring extended endurance. Refer to Xicor reliability reports for further endurance information.

4

### PIN CONFIGURATION

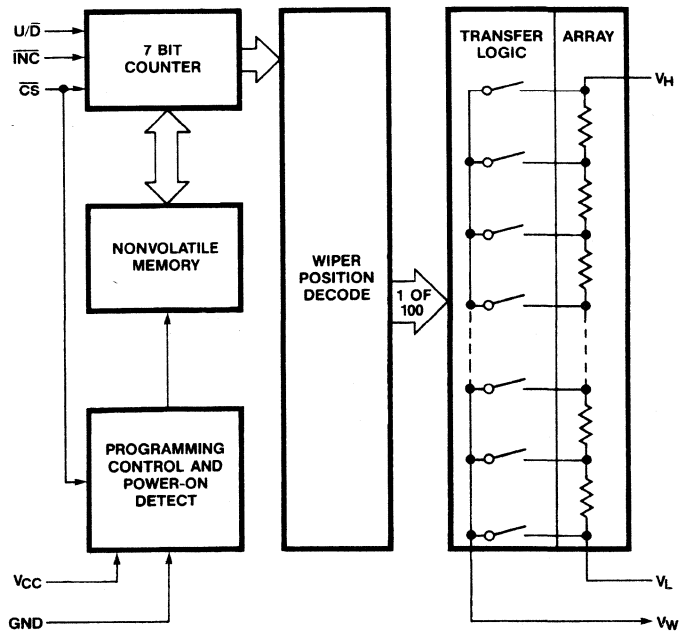


0039-1

### PIN NAMES

$V_H$	High Terminal of Pot
$V_W$	Wiper Terminal of Pot
$V_L$	Low Terminal of Pot
$V_{SS}$	Ground
$V_{CC}$	System Power
$U/\overline{D}$	Up/Down Control
$\overline{INC}$	Wiper Movement Control
$\overline{CS}$	Chip Select for Wiper Movement/Storage

### FUNCTIONAL DIAGRAM



0039-2

# X9MME, X9MMEI

## ANALOG CHARACTERISTICS

### Electrical Characteristics

End to End Resistance Tolerance	±20%
Power Rating at 25°C	10 mW
Wiper Current	±1 mA Max.
Typical Wiper Resistance	40Ω at 1 mA
Typical Noise	< -120 dB/√Hz Ref: 1V

### Resolution

Resistance	1%
------------	----

### Linearity

Absolute Linearity <sup>(1)</sup>	±1.0 MI <sup>(2)</sup>
Relative Linearity <sup>(3)</sup>	±0.2 MI <sup>(2)</sup>

### Temperature Coefficient

-40°C to +85°C	±300 ppm/°C Typical
----------------	---------------------

### Wiper Adjustability

Unlimited Wiper Adjustment (Volatile Mode While Chip is Selected)	
Nonvolatile Storage of Wiper Position	10,000 Cycles Typical

### Environmental Characteristics

Temperature Range	
Operating X9MME	0°C to +70°C
X9MMEI	-40°C to +85°C
Storage	-65°C to +150°C

### Physical Characteristics

Marking Includes:  
 Manufacturer's Trademark  
 Resistance Value or Code  
 Date Code

### ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on $\overline{CS}$ , $\overline{INC}$ , U/D and $V_{CC}$	
Referenced to Ground	-1.0V to +7.0V
Voltage on $V_H$ and $V_L$	
Referenced to Ground	-8.0V to +8.0V
Lead Temperature (Soldering, 10 Seconds)	+300°C
Wiper Current	±1 mA

### \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

X9MME  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

X9MMEI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ. <sup>(4)</sup>	Max.		
$I_{CC}$	Supply Current		25	35	mA	
$I_{LI}$	Input Leakage Current			±10	μA	$V_{IN} = 0V$ to $5.5V$ , $\overline{INC}$ , U/D, $\overline{CS}$
$V_{IH}$	Input High Voltage	2.0		$V_{CC} + 1.0$	V	
$V_{IL}$	Input Low Voltage	-1.0		0.8	V	
$R_W$	Wiper Resistance		40	100	Ω	±1 mA
$V_{VH}$	$V_H$ Voltage	-5.0		+5.0	V	
$V_{VL}$	$V_L$ Voltage	-5.0		+5.0	V	
$C_{IN}^{(5)}$	$\overline{CS}$ , $\overline{INC}$ , U/D, Input Capacitance			10	pF	

**Notes:** (1) Absolute Linearity is utilized to determine actual wiper voltage versus expected voltage as determined by wiper position when used as a potentiometer.

$$\text{Absolute Linearity} = (V_{W(n)}(\text{actual}) - V_{W(n)}(\text{expected})) = \pm 1 \text{ MI Max.}$$

$$(2) 1 \text{ MI} = R_{TOT}/99 \text{ or } \frac{V_H - V_L}{99} = \text{Minimum Increment.}$$

(3) Relative Linearity is utilized to determine the actual change in voltage between successive tap position when used as a potentiometer. It is a measure of the error in step size.

$$\text{Relative Linearity} = V_{W(n+1)} - [V_{W(n)} + \text{MI}] = \pm 0.2 \text{ MI Max.}$$

Typical values of Linearity are shown in Figure 3.

(4) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

(5) This parameter is periodically sampled and not 100% tested.

# X9MME, X9MMEI

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input	1.5V

## MODE SELECTION

$\overline{CS}$	$\overline{INC}$	U/D	Mode
L		H	Wiper Up
L		L	Wiper Down
	H	X	Store Wiper Position

## A.C. CHARACTERISTICS

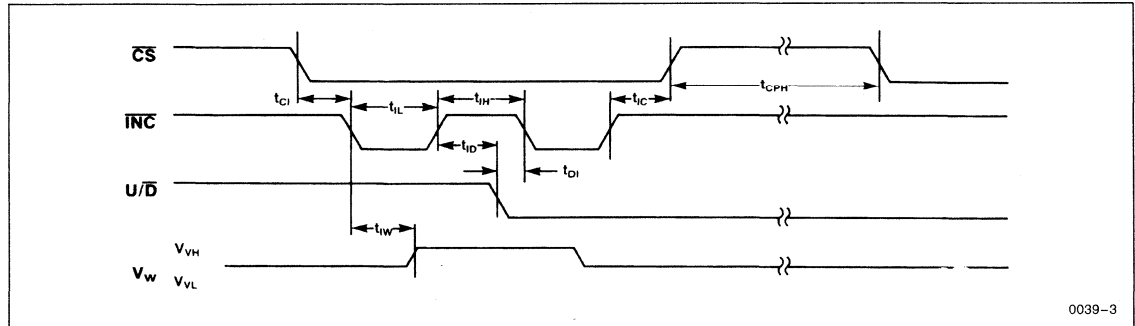
X9MME  $T_A = 0^\circ\text{C}$  to  $+70^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

X9MMEI  $T_A = -40^\circ\text{C}$  to  $+85^\circ\text{C}$ ,  $V_{CC} = +5V \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units
		Min.	Typ.(6)	Max.	
$t_{CI}$	$\overline{CS}$ to $\overline{INC}$ Setup	100			ns
$t_{ID}$	$\overline{INC}$ High to U/D Change	100			ns
$t_{DI}$	U/D to $\overline{INC}$ Setup	2.9			$\mu\text{s}$
$t_{IL}$	$\overline{INC}$ Low Period	1			$\mu\text{s}$
$t_{IH}$	$\overline{INC}$ High Period	3			$\mu\text{s}$
$t_{IC}$	$\overline{INC}$ Inactive to $\overline{CS}$ Inactive	1			$\mu\text{s}$
$t_{CPH}$	$\overline{CS}$ Deselect Time	20			ms
$t_{IW}$	$\overline{INC}$ to $V_W$ Change		100	500	$\mu\text{s}$

4

## A.C. Timing



Note: (6) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X9MME, X9MMEI

## PIN DESCRIPTIONS

### $V_H$

The high terminal of the X9MME is capable of handling an input voltage from  $-5V$  to  $+5V$ .

### $V_L$

The low terminal input is limited from  $-5V$  to  $+5V$ .

### $V_W$

The wiper terminal series resistance is typically less than  $40\Omega$ . The value of the wiper is controlled by the use of  $U/\bar{D}$  and  $\bar{INC}$ .

### Up/Down ( $U/\bar{D}$ )

The  $U/\bar{D}$  input controls the direction of the wiper movement and the value of the nonvolatile counter.

### Increment ( $\bar{INC}$ )

The  $\bar{INC}$  input is negative-edge triggered. Toggling  $\bar{INC}$  will move the wiper and either increment or decrement the counter in the direction indicated by the logic level on the  $U/\bar{D}$  input.

### Chip Select ( $\bar{CS}$ )

The device is selected when the  $\bar{CS}$  input is LOW. The current counter value is stored in nonvolatile memory when  $\bar{CS}$  is returned HIGH with  $\bar{INC}$  HIGH.

## DEVICE OPERATION

The  $\bar{INC}$ ,  $U/\bar{D}$  and  $\bar{CS}$  inputs control the movement of the wiper along the resistor array. HIGH to LOW transitions on  $\bar{INC}$ , with  $\bar{CS}$  LOW, increment ( $U/\bar{D} = \text{HIGH}$ ) or decrement ( $U/\bar{D} = \text{LOW}$ ) an internal counter. The output of the counter is decoded to position the wiper. When  $\bar{CS}$  is brought HIGH the counter value is automatically stored in the nonvolatile memory. Upon power-up the nonvolatile memory contents are restored to the counter.

With the wiper at position 99, additional increments ( $U/\bar{D} = \text{HIGH}$ ) will not move the wiper. With the wiper at position 0, additional decrements ( $U/\bar{D} = \text{LOW}$ ) will not move the wiper.

The state of  $U/\bar{D}$  may be changed while  $\bar{CS}$  remains LOW, allowing a gross then fine adjustment during system calibration.

If  $V_{CC}$  is removed while  $\bar{CS}$  is LOW the contents of the nonvolatile memory may be lost.

The end to end resistance of the array will fluctuate once  $V_{CC}$  is removed.

## APPLICATIONS

The combination of a digital interface and nonvolatile memory in a silicon based trimmer pot provides many application opportunities that could not be addressed by either mechanical potentiometers or digital to analog circuits. The X9MME addresses and solves many issues that are of concern to designers of a wide range of equipment.

Consider the possibilities:

Automated assembly line calibration versus mechanical tweaking of potentiometers.

Protection against drift due to vibration or contamination.

Eliminate precise alignment of PWB mounted potentiometers with case access holes.

Eliminate unsightly access holes on otherwise aesthetically pleasing enclosures.

Product enhancements such as keyboard adjustment of volume or brightness control.

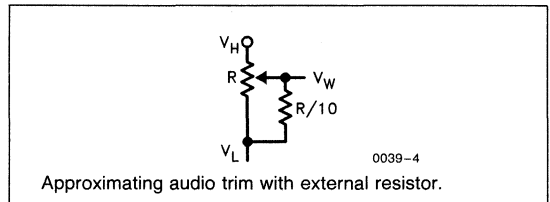
Front panel microprocessor controlled calibration of test instruments.

Remote location calibration via radio, modem or LAN link.

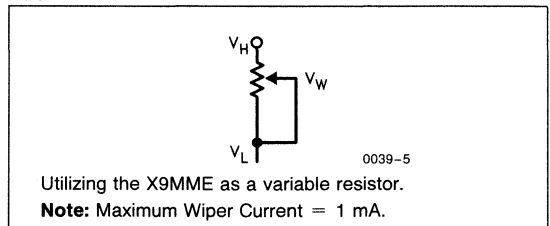
Calibration of hard to reach instruments in aircraft or other confined spaces.

## APPLICATION CIRCUITS

### Application Circuit # 1

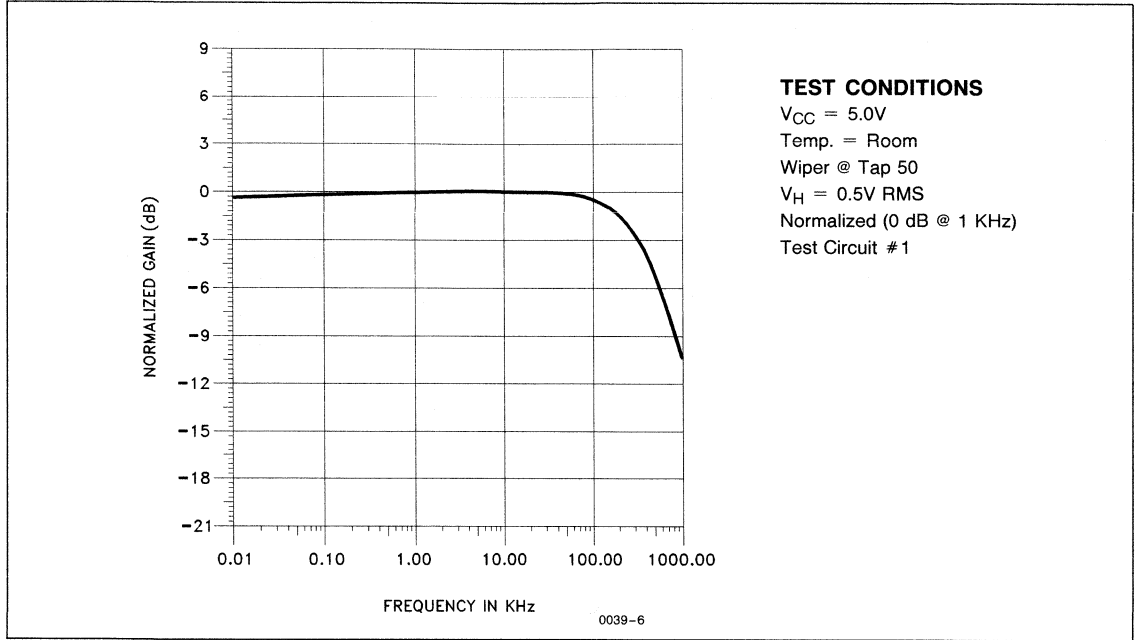


### Application Circuit # 2



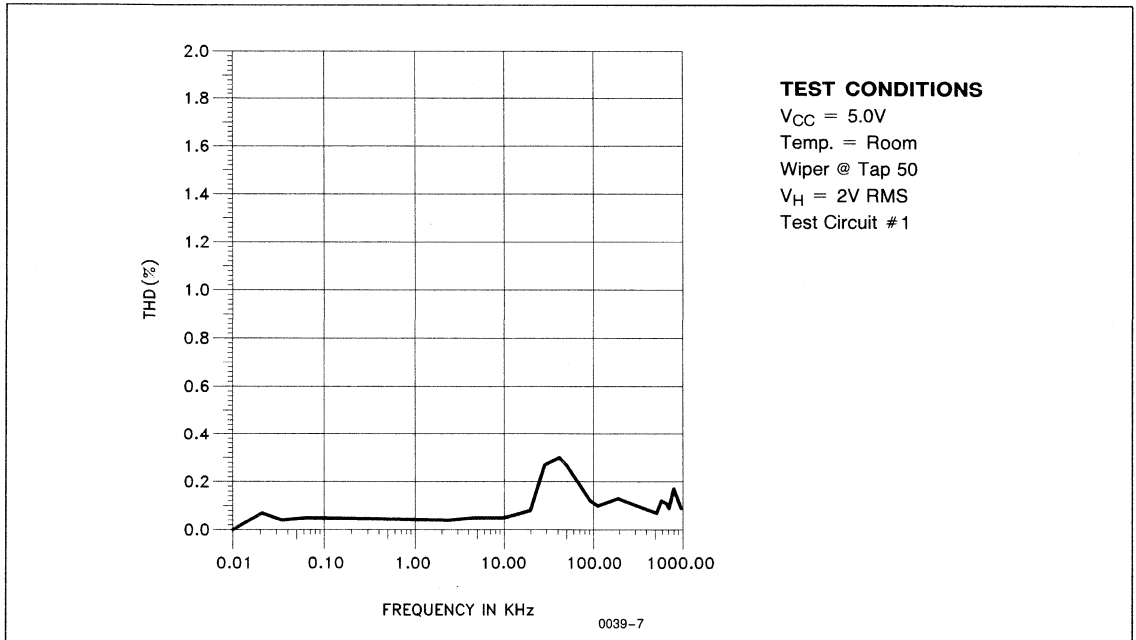
# X9MME, X9MMEI

Figure 1: Typical Frequency Response for X9103



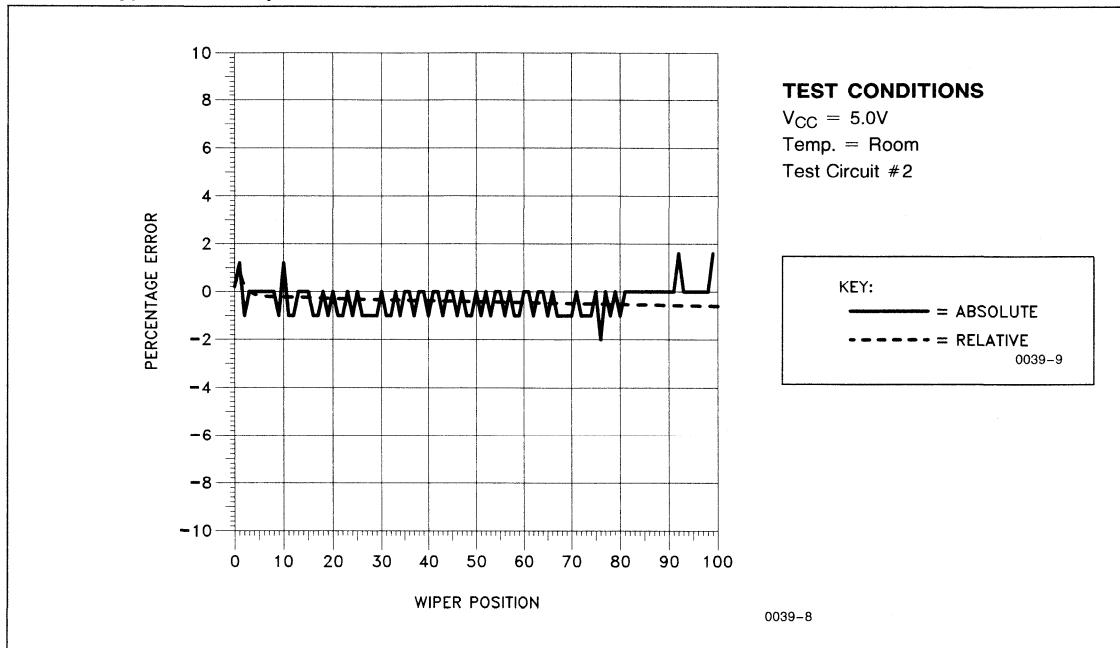
4

Figure 2: Typical Total Harmonic Distortion for X9103

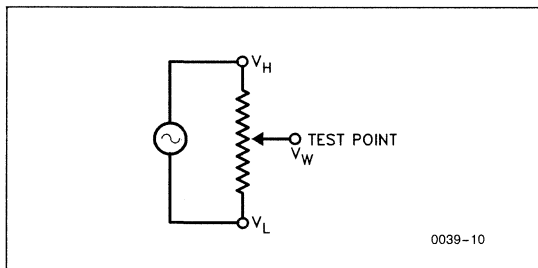


# X9MME, X9MMEI

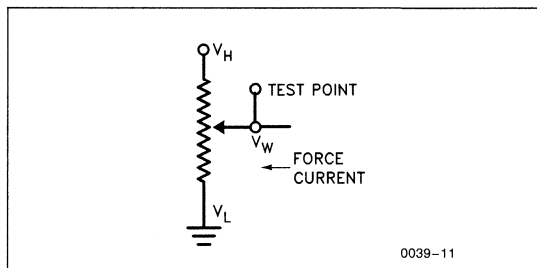
Figure 3: Typical Linearity for X9103



Test Circuit # 1



Test Circuit # 2



## Standard Parts

Minimum Resistance	Wiper Increments	Maximum Resistance	Part Number
40Ω	101Ω	10 KΩ	X9103
40Ω	505Ω	50 KΩ	X9503
40Ω	1010Ω	100 KΩ	X9104

**Military**

**X9MMEM**

## E<sup>2</sup>POT™ Digitally Controlled Potentiometer

### FEATURES

- **Solid State Reliability**
- **Single Chip MOS Implementation**
- **Three Wire TTL Control**
- **Operates From Standard 5V Supply**
- **Wide Analog Voltage Range  $\pm 5V$  Min.**
- **99 Resistive Elements**
  - Temperature Compensated
  - $\pm 20\%$  End to End Resistance Range
- **100 Wiper Tap Points**
  - Wiper Position Digitally Controlled
  - Wiper Position Stored in Nonvolatile Memory Then Automatically Recalled on Power-Up
- **100 Year Wiper Position Retention**
- **8 Pin Mini-DIP Package**

### DESCRIPTION

The Xicor X9MME is a solid state nonvolatile potentiometer, packaged in an 8 pin mini-DIP and is ideal for digitally controlled resistance trimming.

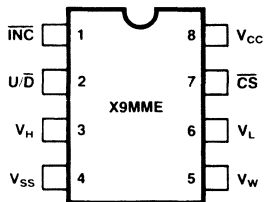
The X9MME is a resistor array composed of 99 resistive elements. Between each element and at either end are tap points accessible to the wiper element. The position of the wiper element on the array is controlled by the  $\overline{CS}$ ,  $U/\overline{D}$ , and  $\overline{INC}$  inputs. The position of the wiper can be stored in nonvolatile memory and is recalled upon a subsequent power-up.

The resolution of the X9MME is equal to the maximum resistance value divided by 99. As an example; for the X9503 (50 K $\Omega$ ) each tap point represents 505 $\Omega$ .

Xicor E<sup>2</sup> products are designed and tested for applications requiring extended endurance. Refer to Xicor reliability reports for further endurance information.

4

### PIN CONFIGURATION

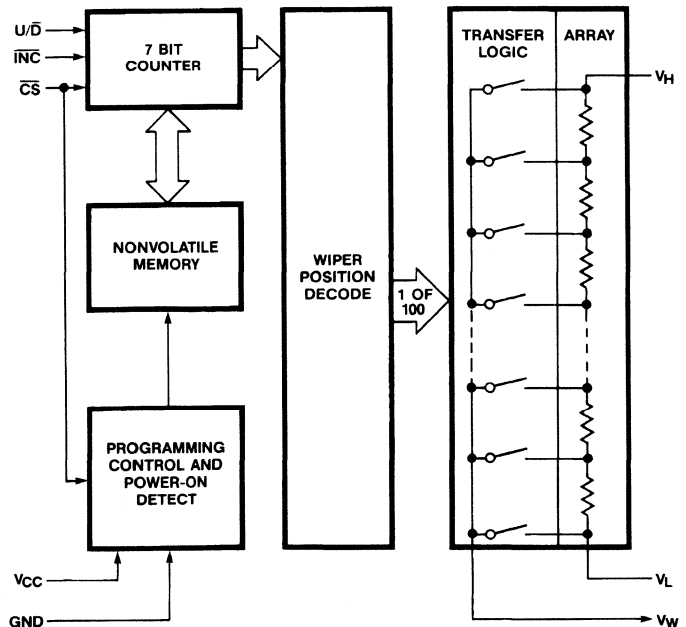


0048-1

### PIN NAMES

$V_H$	High Terminal of Pot
$V_W$	Wiper Terminal of Pot
$V_L$	Low Terminal of Pot
$V_{SS}$	Ground
$V_{CC}$	System Power
$U/\overline{D}$	Up/Down Control
$\overline{INC}$	Wiper Movement Control
$\overline{CS}$	Chip Select for Wiper Movement/Storage

### FUNCTIONAL DIAGRAM



0048-2

# X9MMEM

## ANALOG CHARACTERISTICS

### Electrical Characteristics

End to End Resistance Tolerance	± 20%
Power Rating at 25°C	10 mW
Wiper Current	± 1 mA Max.
Typical Wiper Resistance	40Ω at 1 mA
Typical Noise	< -120 dB/√Hz Ref: 1V

### Resolution

Resistance	1%
------------	----

### Linearity

Absolute Linearity <sup>(1)</sup>	± 1.0 MI <sup>(2)</sup>
Relative Linearity <sup>(3)</sup>	± 0.2 MI <sup>(2)</sup>

### Temperature Coefficient

-55°C to +125°C	± 300 ppm/°C Typical
-----------------	----------------------

### Wiper Adjustability

Unlimited Wiper Adjustment (Volatile Mode While Chip is Selected) Nonvolatile Storage of Wiper Position	10,000 Cycles Typical
---	-----------------------

### Environmental Characteristics

Temperature Range	
Operating	-55°C to +125°C
Storage	-65°C to +150°C

### Physical Characteristics

Marking Includes:	
Manufacturer's Trademark	
Resistance Value or Code	
Date Code	

### ABSOLUTE MAXIMUM RATINGS\*

Temperature Under Bias	-65°C to +135°C
Storage Temperature	-65°C to +150°C
Voltage on CS, INC, U/D and V <sub>CC</sub>	
Referenced to Ground	-1.0V to +7.0V
Voltage on V <sub>H</sub> and V <sub>L</sub>	
Referenced to Ground	-8.0V to +8.0V
Lead Temperature (Soldering, 10 Seconds)	+300°C
Wiper Current	± 1 mA

### \*COMMENT

Stresses above those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. This is a stress rating only and the functional operation of the device at these or any other conditions above those indicated in the operational sections of this specification is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

## D.C. OPERATING CHARACTERISTICS

T<sub>A</sub> = -55°C to +125°C, V<sub>CC</sub> = +5V ± 10%, unless otherwise specified.

Symbol	Parameter	Limits			Units	Test Conditions
		Min.	Typ. <sup>(4)</sup>	Max.		
I <sub>CC</sub>	Supply Current		25	35	mA	
I <sub>LI</sub>	Input Leakage Current			± 10	μA	V <sub>IN</sub> = 0V to 5.5V, $\overline{\text{INC}}$ , U/D, $\overline{\text{CS}}$
V <sub>IH</sub>	Input High Voltage	2.0		V <sub>CC</sub> + 1.0	V	
V <sub>IL</sub>	Input Low Voltage	-1.0		0.8	V	
R <sub>W</sub>	Wiper Resistance		40	100	Ω	± 1 mA
V <sub>VH</sub>	V <sub>H</sub> Voltage	-5.0		+5.0	V	
V <sub>VL</sub>	V <sub>L</sub> Voltage	-5.0		+5.0	V	
C <sub>IN</sub> <sup>(5)</sup>	$\overline{\text{CS}}$ , $\overline{\text{INC}}$ , U/D, Input Capacitance			10	pF	

**Notes:** (1) Absolute Linearity is utilized to determine actual wiper voltage versus expected voltage as determined by wiper position when used as a potentiometer.

$$\text{Absolute Linearity} = (V_{W(n)}(\text{actual}) - V_{W(n)}(\text{expected})) = \pm 1 \text{ MI Max.}$$

$$(2) 1 \text{ MI} = R_{\text{TOT}}/99 \text{ or } \frac{V_H - V_L}{99} = \text{Minimum Increment.}$$

(3) Relative Linearity is utilized to determine the actual change in voltage between successive tap position when used as a potentiometer. It is a measure of the error in step size.

$$\text{Relative Linearity} = V_{W(n+1)} - [V_{W(n)} + \text{MI}] = \pm 0.2 \text{ MI Max.}$$

Typical values of Linearity are shown in Figure 3.

(4) Typical values are for T<sub>A</sub> = 25°C and nominal supply voltage.

(5) This parameter is periodically sample and not 100% tested.



# X9MMEM

## A.C. CONDITIONS OF TEST

Input Pulse Levels	0V to 3.0V
Input Rise and Fall Times	10 ns
Input	1.5V

## MODE SELECTION

$\overline{CS}$	$\overline{INC}$	U/ $\overline{D}$	Mode
L		H	Wiper Up
L		L	Wiper Down
	H	X	Store Wiper Position

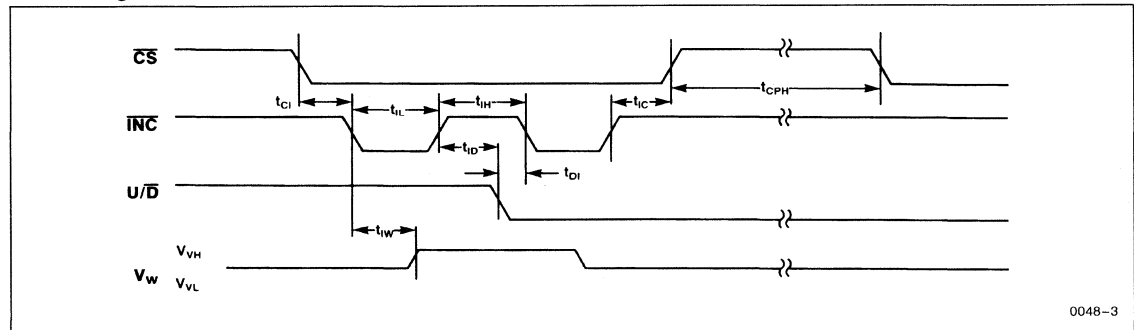
## A.C. CHARACTERISTICS

$T_A = -55^\circ\text{C}$  to  $+125^\circ\text{C}$ ,  $V_{CC} = +5\text{V} \pm 10\%$ , unless otherwise specified.

Symbol	Parameter	Limits			Units
		Min.	Typ.(6)	Max.	
$t_{CI}$	$\overline{CS}$ to $\overline{INC}$ Setup	100			ns
$t_{ID}$	$\overline{INC}$ High to U/ $\overline{D}$ Change	100			ns
$t_{DI}$	U/ $\overline{D}$ to $\overline{INC}$ Setup	2.9			$\mu\text{s}$
$t_{IL}$	$\overline{INC}$ Low Period	1			$\mu\text{s}$
$t_{IH}$	$\overline{INC}$ High Period	3			$\mu\text{s}$
$t_{IC}$	$\overline{INC}$ Inactive to $\overline{CS}$ Inactive	1			$\mu\text{s}$
$t_{CPH}$	$\overline{CS}$ Deselect Time	20			ms
$t_{IW}$	$\overline{INC}$ to $V_W$ Change		100	500	$\mu\text{s}$

4

## A.C. Timing



**Note:** (6) Typical values are for  $T_A = 25^\circ\text{C}$  and nominal supply voltage.

# X9MMEM

## PIN DESCRIPTIONS

### $V_H$

The high terminal of the X9MME is capable of handling an input voltage from  $-5V$  to  $+5V$ .

### $V_L$

The low terminal input is limited from  $-5V$  to  $+5V$ .

### $V_W$

The wiper terminal series resistance is typically less than  $40\Omega$ . The value of the wiper is controlled by the use of  $U/\bar{D}$  and  $\bar{INC}$ .

### Up/Down ( $U/\bar{D}$ )

The  $U/\bar{D}$  input controls the direction of the wiper movement and the value of the nonvolatile counter.

### Increment ( $\bar{INC}$ )

The  $\bar{INC}$  input is negative-edge triggered. Toggling  $\bar{INC}$  will move the wiper and either increment or decrement the counter in the direction indicated by the logic level on the  $U/\bar{D}$  input.

### Chip Select ( $\bar{CS}$ )

The device is selected when the  $\bar{CS}$  input is LOW. The current counter value is stored in nonvolatile memory when  $\bar{CS}$  is returned HIGH with  $\bar{INC}$  HIGH.

## DEVICE OPERATION

The  $\bar{INC}$ ,  $U/\bar{D}$  and  $\bar{CS}$  inputs control the movement of the wiper along the resistor array. HIGH to LOW transitions on  $\bar{INC}$ , with  $\bar{CS}$  LOW, increment ( $U/\bar{D} = \text{HIGH}$ ) or decrement ( $U/\bar{D} = \text{LOW}$ ) an internal counter. The output of the counter is decoded to position the wiper. When  $\bar{CS}$  is brought HIGH the counter value is automatically stored in the nonvolatile memory. Upon power-up the nonvolatile memory contents are restored to the counter.

With the wiper at position 99, additional increments ( $U/\bar{D} = \text{HIGH}$ ) will not move the wiper. With the wiper at position 0, additional decrements ( $U/\bar{D} = \text{LOW}$ ) will not move the wiper.

The state of  $U/\bar{D}$  may be changed while  $\bar{CS}$  remains LOW, allowing a gross then fine adjustment during system calibration.

If  $V_{CC}$  is removed while  $\bar{CS}$  is LOW the contents of the nonvolatile memory may be lost.

The end to end resistance of the array will fluctuate once  $V_{CC}$  is removed.

## APPLICATIONS

The combination of a digital interface and nonvolatile memory in a silicon based trimmer pot provides many application opportunities that could not be addressed by either mechanical potentiometers or digital to analog circuits. The X9MME addresses and solves many issues that are of concern to designers of a wide range of equipment.

Consider the possibilities:

Automated assembly line calibration versus mechanical tweaking of potentiometers.

Protection against drift due to vibration or contamination.

Eliminate precise alignment of PWB mounted potentiometers with case access holes.

Eliminate unsightly access holes on otherwise aesthetically pleasing enclosures.

Product enhancements such as keyboard adjustment of volume or brightness control.

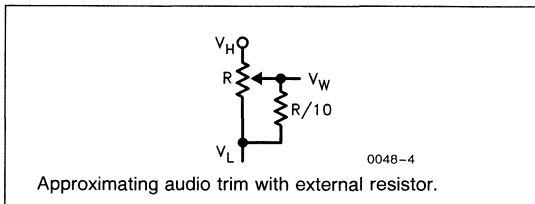
Front panel microprocessor controlled calibration of test instruments.

Remote location calibration via radio, modem or LAN link.

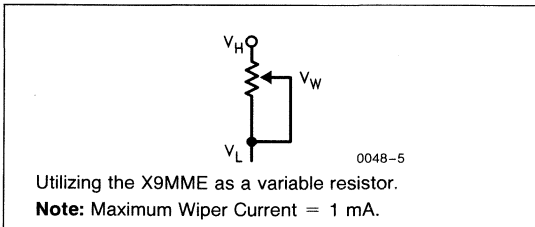
Calibration of hard to reach instruments in aircraft or other confined spaces.

## APPLICATION CIRCUITS

### Application Circuit # 1

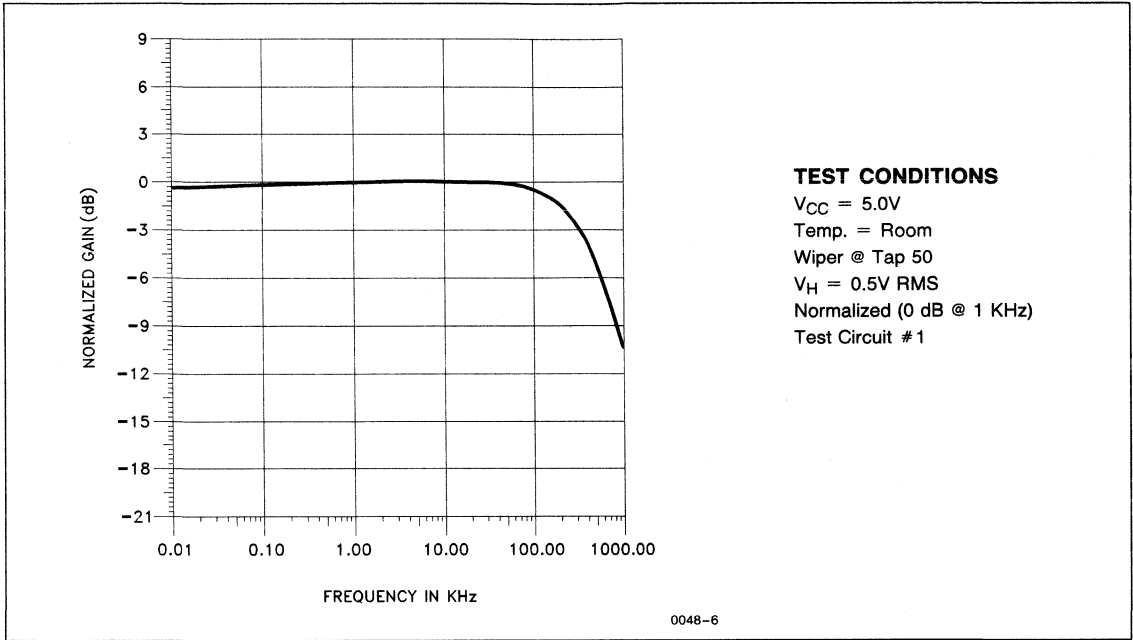


### Application Circuit # 2



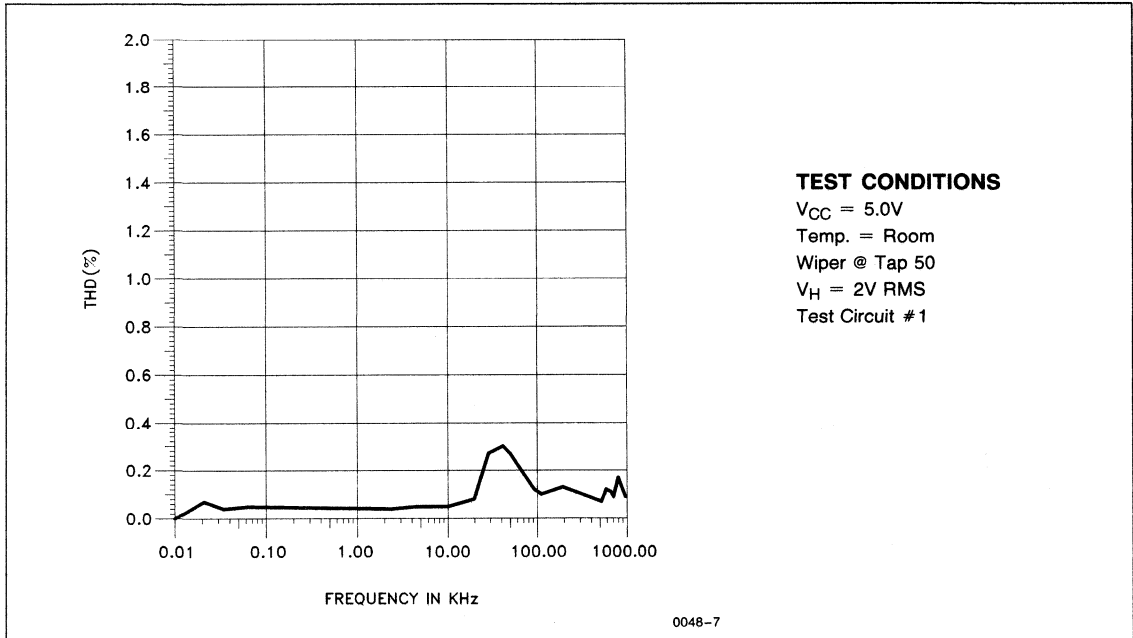
# X9MMEM

Figure 1: Typical Frequency Response for X9103



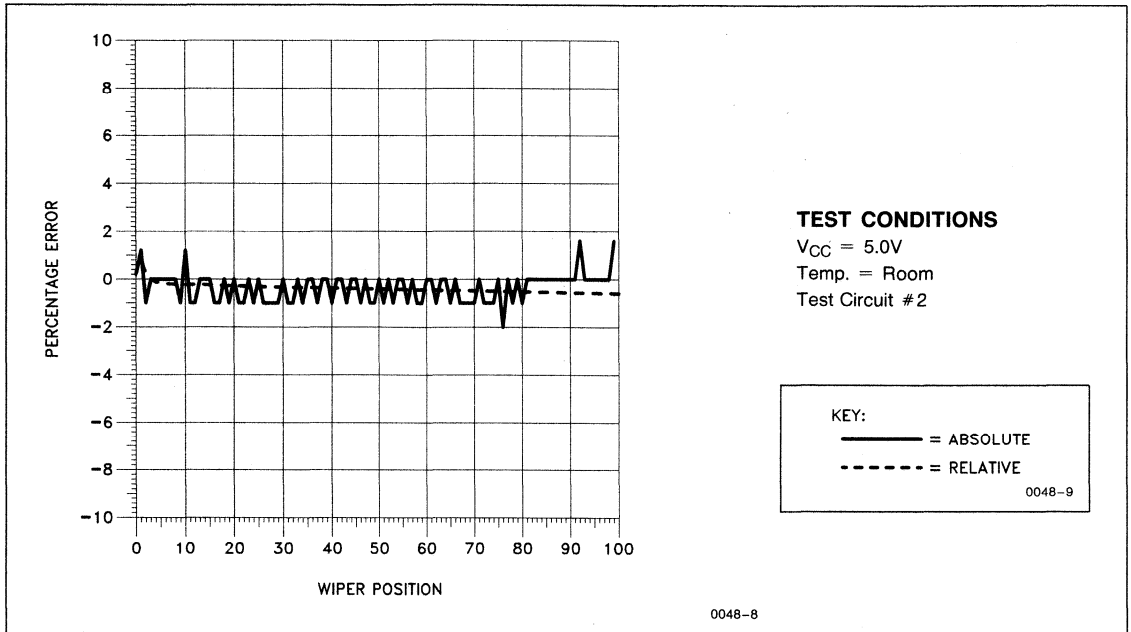
4

Figure 2: Typical Total Harmonic Distortion for X9103

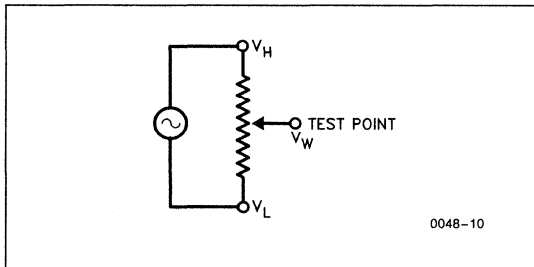


# X9MEM

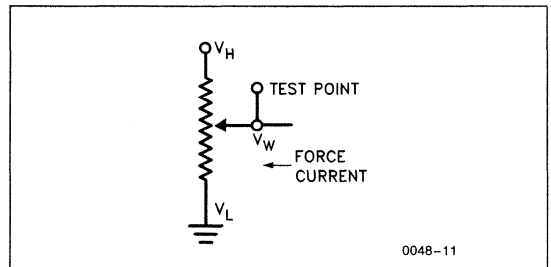
**Figure 3: Typical Linearity for X9103**



**Test Circuit # 1**



**Test Circuit # 2**



**Standard Parts**

Minimum Resistance	Wiper Increments	Maximum Resistance	Part Number
40Ω	101Ω	10 KΩ	X9103
40Ω	505Ω	50 KΩ	X9503
40Ω	1010Ω	100 KΩ	X9104

Die Products ..... 5-1

**NOVRAM\* Data Sheets**

**1**

**Serial I/O Data Sheets**

**2**

**E<sup>2</sup>PROM Data Sheets**

**3**

**E<sup>2</sup>POT™ Digitally Controlled  
Potentiometer Data Sheets**

**4**



**Die Products**

**5**



## Die Products

### FEATURES

- High Performance Advanced NMOS Technology
- 0°C to 70°C Operating Temperature
- 100 Year Data Retention
- 95% Yield Excluding Assembly Related Losses
- Standard Thickness Between 20 to 22 mils
- Commercial Data Sheet Parameters (except input levels)
- Die Inspected to 883C 2010.7 Condition B

### DESCRIPTION

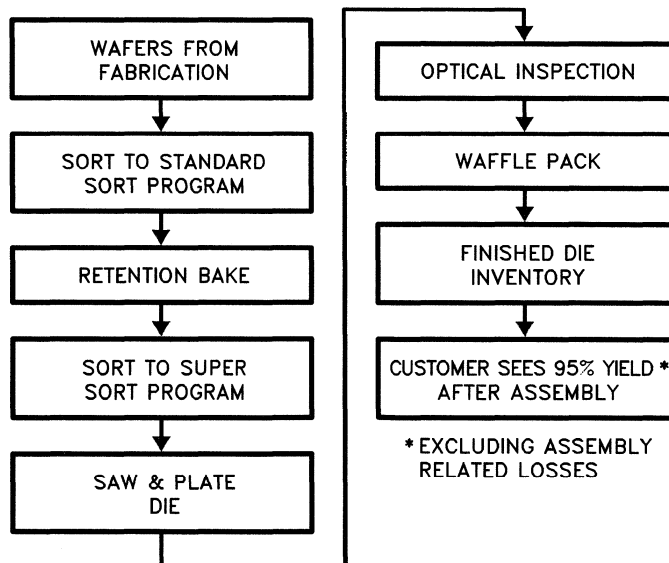
Xicor die products are fabricated with an advanced, high performance N-channel floating gate MOS technology. Like all Xicor programmable nonvolatile memories, they are 5V only devices.

Xicor die products are designed and tested for applications requiring extended endurance. Data retention is specified to be greater than 100 years.

Products to be shipped in die form follow the flow shown below. This insures a 95% yield (excluding assembly related losses) to the commercial data sheet with the access times per the Die Products Reference Guide. All A.C. parameters and D.C. parameters except input and output voltages are guaranteed.

Bonding diagrams, die size and other information required for use of die can be obtained from your local Xicor sales representative.

### TEST FLOW



0074-1

# Die Products

---

## DIE PRODUCTS REFERENCE GUIDE

### E<sup>2</sup>PROMs

Part Number	Organization	Page Size (Bytes)	Access Time (ns)	Power Requirements (mA)	
				Active (Max.)	Standby (Max.)
X2804AH	512 x 8	N/A	450	80	50
X2816BH	2K x 8	16	450	120	60
X2864AH	8K x 8	16	450	140	60
X2864BH	8K x 8	32	200	150	80

### NOVRAMs

Part Number	Organization	Access Time (ns)	Store Cycles	Power Requirements (mA)	
				Active (Max.)	Standby (Max.)
X2004H	512 x 8	300	100,000	100	55

### Serial E<sup>2</sup>PROMs

Part Number	Organization	Page Size (Bytes)	Clock Frequency	Power Requirements (mA)	
				Active (Max.)	Standby (Max.)
X2402H	256 x 8	8	100 KHz	30	25
X2404H	512 x 8	8	100 KHz	30	25

### Serial NOVRAMs

Part Number	Organization	Clock Frequency	Store Cycles	Power Requirements (mA)		
				Active	Standby	Sleep
X2444H	16 x 16	1 MHz	100,000	15	10	7

### Digital Potentiometers

Part Number	End to End Resistance	Maximum Voltage (V <sub>H</sub> , V <sub>L</sub> )	Power Requirements (mA)
X9103H	10 K $\Omega$	$\pm 5V$	35
X9503H	50 K $\Omega$	$\pm 5V$	35
X9104H	100 K $\Omega$	$\pm 5V$	35



Military 883 Program Overview . . . . . 6-1

**NOVRAM\* Data Sheets 1**

**Serial I/O Data Sheets 2**

**E<sup>2</sup>PROM Data Sheets 3**

**E<sup>2</sup>POT™ Digitally Controlled Potentiometer Data Sheets 4**

**Die Products 5**



**Military 6**





# MILITARY PROGRAM OVERVIEW

presented to illustrate Xicor's commitment to maintaining the highest standards of quality in our products.

## MIL-STD-883C FLOWS

### INTRODUCTION

Xicor's Military program offers the largest selection of NOVRAMs\* and E<sup>2</sup>PROMs qualified to MIL-STD-883C, Class B. This Military overview is

All Xicor devices marked with a "B" are manufactured and screened to the requirements of MIL-STD-883C, Class B. The product flow is illustrated in Figure 1, with detailed device screening and test methods illustrated below.

#### Assembly, Environmental and Final Test Screening Methods

SCREEN		TEST METHOD	APPLICATION
Internal Visual		2010, Condition B	100%
Stabilization Bake		1008, Condition C (48 hours)	100%
Temperature Cycling		1010, Condition C	100%
Constant Acceleration		2001, Condition E, Y-axis	100%
Seal:	Fine	1014, Condition A or B	100%
	Gross	1014, Condition C	100%
External Visual		2009	100%
Pre Burn-In Electricals		Per Device Data Sheet	100%
Dynamic Burn-In		1015, Condition D, 160 Hours at + 125°C	100%
Final Electricals		Per Device Data Sheet	Periodic Inspection
Static Tests		Subgroups 1, 2, 3 1/	
Switching Tests		Subgroups 9, 10, 11	
Functional Tests		Subgroups 7, 8	
Dynamic Tests		Subgroup 4 (Method 3012)	
Solder Dip Lead Finish		MIL-M-38510, Paragraph 3.5.6.2.1.Q	100%
Seal:	Fine	1014, Condition A or B	100%
	Gross	1014, Condition C	100%
External Visual		2009	100%
Quality Conformance Inspection		2/	Sample

6

**Notes:** (1) Percent defective allowable (PDA) is 5% (Subgroups 1, 7, 9) for each lot.

(2) Samples will be selected for testing in accordance with Class B requirements of Method 5005, Groups A, B, C and D.

\*NOVRAM is Xicor's nonvolatile static RAM device.

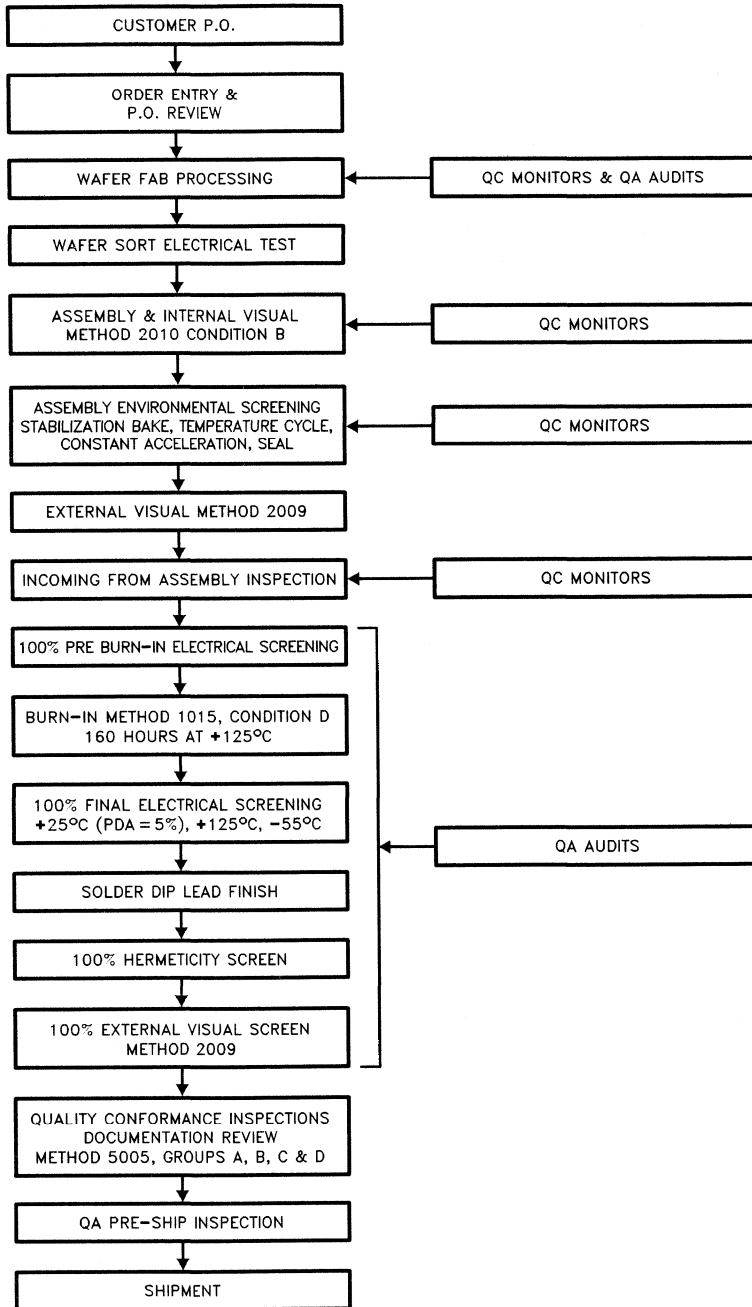


Figure 1: MIL-STD-883C, Class B, Product Flow

# Quality Conformance Inspections, Method 5005

The following Tables illustrate the Groups A, B, C and D Screens, Test Methods, Conditions and frequency of testing for all qualified products.

**TABLE I: Group A Electrical Tests**  
Performed on each lot or subplot

SCREEN	SUBGROUP	LTPD
Static Tests at +25°C	1	2
Static Tests at +125°C	2	3
Static Tests at -55°C	3	5
Functional Tests at +25°C	7	2
Functional Tests at +125°C	8	3
Functional Tests at -55°C	8	5
Switching Tests at +25°C	9	2
Switching Tests at +125°C	10	3
Switching Tests at -55°C	11	5

**TABLE II: Group B Assembly Integrity Tests**

Performed on each lot

SCREEN	TEST METHOD	CONDITIONS	LTPD*
<b>Subgroup 1</b> Physical Dimensions	2016	MIL-M-38510, Appendix C	2/0
<b>Subgroup 2</b> Resistance to Solvents	2015	Top and Bottom Mark	4/0
<b>Subgroup 3</b> Solderability	2003	Solder Temperature: +245°C ± 5°C	15
<b>Subgroup 4</b> Internal Visual and Mechanical	2014	Per Design and Construction	1/0
<b>Subgroup 5</b> Bond Strength	2011	Condition D	15

\*LTPD = Quantity / Accept Number

**TABLE III: Group C Die Related Tests**

Performed by inspection lot every 26 weeks

SCREEN	TEST METHOD	CONDITIONS	LTPD
<b>Subgroup 1</b> Steady State Lifetest Endpoint Electricals	1005	Condition B Subgroups 1, 2, 3, 7, 8, 9, 10, 11 Per Applicable Device Specification	5
<b>Subgroup 2</b> Temperature Cycling Constant Acceleration Seal: Fine Gross Visual Examination Endpoint Electricals	1010 2001 1014 1014 1010	Condition C, 10 Cycles Condition E, 30 Kg, Y1 Condition A or B Condition C  Subgroups 1, 2, 3, 7, 8, 9, 10, 11 Per Applicable Device Specification	15

6

**TABLE IV: Group D Package Related Tests**

Performed by inspection lot every 26 weeks

SCREEN	TEST METHOD	CONDITIONS	LTPD*
<b>Subgroup 1</b> Physical Dimensions	2016	MIL-M-38510, Appendix C	15
<b>Subgroup 2</b> Lead Integrity Seal: Fine Gross	2004 1014 1014	Condition B2, Lead Fatigue Condition A or B Condition C	15
<b>Subgroup 3</b> Thermal Shock Temperature Cycling Moisture Resistance Endpoint Electricals Seal: Fine Gross Visual Examination	1011 1010 1004 5005 1014 1014 1010 and 1004	Condition B, 15 Cycles Condition C, 100 Cycles 10 Cycles Subgroups 1, 7, 9 (Within 48 Hours) Condition A or B Condition C	15
<b>Subgroup 4</b> Mechanical Shock Variable Frequency Vibration Constant Acceleration Seal: Fine Gross Visual Examination Endpoint Electricals	2002 2007 2001 1014 1014 1010	Condition B, 1.5 Kg at 0.5 ms Condition A, 4 Cycles X, Y & Z Condition E, 30 Kg, Y1 Condition A or B Condition C  Subgroups 1, 7, 9 Per Applicable Device Specification	15
<b>Subgroup 5</b> Salt Atmosphere Seal: Fine Gross Visual Examination	1009 1014 1014 1009	Condition A, 24 Hours Condition A or B Condition C	15
<b>Subgroup 6</b> Internal Water Vapor Content	1018	5000 ppm at 100°C	5/1
<b>Subgroup 7</b> Adhesion of Lead Finish	2025	5 Leads Per Device (LTPD Applies to Leads)	15
<b>Subgroup 8</b> Lid Torque	2024		5/0

\*LTPD = Quantity / Accept Number

---

## **ADDITIONAL DATA AND SERVICES**

### **Source Control Drawings**

Customers may provide source control drawings for Xicor review and quotation. To reduce overall product cost to the consumer and to assure compliance with the requirements of MIL-STD-883C, Xicor will respond with waiver requests as needed. Xicor must review and accept a customer source control drawing prior to order acceptance to assure compliance with the customer specification. Orders to source control drawings must be placed direct with the factory to assure compliance. A customer may, however, purchase standard Xicor product with REFERENCE ONLY to the SCD either directly from the factory or through one of Xicor's franchised distributor locations.

### **Quality Conformance Inspection Data**

QCI data Groups A and B are performed on each lot of devices as standard procedure for all MIL-STD-883C, Class B products. This data is available to the customer and should be requested at the time of quotation to insure its shipment with the product.

Generic QCI data for Groups C and D which qualified the product being shipped is also available. Lot specific QCI data for Groups C and D can also be supplied; however, this may impact delivery lead times and should be requested prior to order placement.

Attributes data, a copy of the lot traveler which accompanies the product through assembly, screening and final test, is also available for customer purchase. This requirement should be specified and quoted prior to order placement.

### **Customer Source Inspection**

Customer source inspection may be performed at final ship point at Xicor. This requirement would be specified and quoted prior to order placement. The standard customer source inspection is comprised of the following:

1. Group A electrical testing. Sample size based on Table I Method 5005 MIL-STD-883C LTPD values and Table B-I Appendix B of MIL-M-38510.
2. Documentation review of all travelers, drawings and purchase orders.
3. Physical Dimensions performed on 2 devices maximum per method 2016, MIL-STD-883C.

### **Dynamic Burn-In Circuit Diagrams and Timing**

In order to assist in the writing of customer source control drawings the individual product burn-in circuits and timing diagrams are illustrated in Figures 3 through 10. In addition thermal resistance data is provided in Table V and a Device Traceability key and Assembly Plant Location Key are provided in Figures 11 and 12 respectively.

# Certificate of Compliance

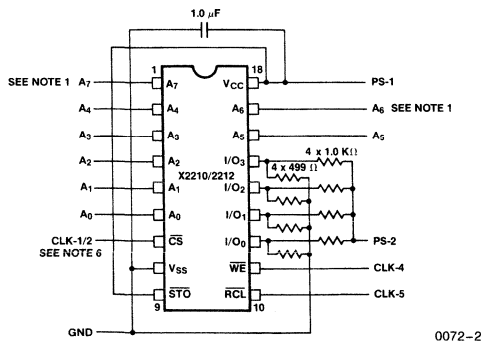
A certificate of compliance accompanies each shipment of MIL-STD-883C, Class B devices. An example is shown in Figure 2 below.

CERTIFICATE OF COMPLIANCE	
<p>This is to certify that these units have been processed in conformance with Method 5004 and Method 5005 of MIL-STD 883 for Class B material as listed below. Additionally, these units are representative of a part type and package that has passed the qualification and quality conformance procedures as specified in method 5005 of MIL-STD 883 Rev. C for Class B material listed below.</p>	
OPERATION	MIL-STD-883 REV. C
Internal Visual	Method 2010 Condition B
Stabilization Bake	Method 1008 Condition C 24 hrs @ 150 deg
Temperature Cycling	Method 1010 Condition C 10 cycles -65 to 150 deg
Constant Acceleration	Method 2001 Condition E 30K G's, Y axis only
Fine Leak	Method 1014 Condition B
Gross Leak	Method 1014 Condition B
Initial Electrical	Per applicable device specification
Burn-In	Method 1015 Condition D 168 hrs @ 125 deg C
Interim Electrical	25 deg C per applicable device spec [PDA = 5 deg @ 125 deg C]
Final Electrical	Method 5005 and applicable device spec
External Visual	Method 2009
Group A Electrical	Method 5005 and applicable device spec
Group B QCI	Method 5005 Class B or generic data where applicable
Bond Strength	Subgroup 5 Method 2011 Condition D
Int. Water Vapor	Subgroup 6 Not Applicable
Seal	Subgroup 7 Method 1014 Conditions B,C
ESD Classification	Device rated Level A
Group C & D QCI	Method 5005 Class B or generic data where applicable
PART # _____	
LOT # _____	
DATE _____	
P.O # _____	_____
S.O # _____	Manager
	Product Assurance
Comments _____	
_____	

0072-21

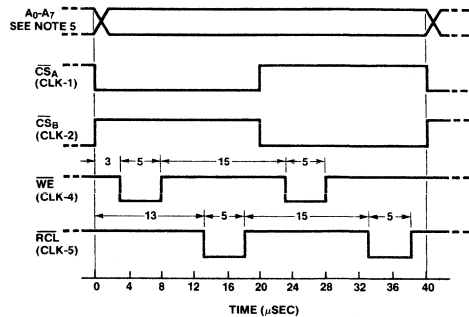
Figure 2: Certificate of Compliance





- Notes:** (1) Pin 1 (A<sub>7</sub>) and Pin 17 (A<sub>6</sub>) are no connects (NC) for the X2210.  
 (2)  $\overline{STO}$  must always be hardwired to V<sub>CC</sub> (Pin 18) at device.  
 (3) All resistors: 1% metal film; 1/4 W.  
 (4) I/O pull-up: 1.0 K $\Omega$   
 I/O pull-down: 499 $\Omega$   
 (5) Socket-to-socket isolation as shown.  
 (6) CLK-1: Rows 1, 3, 5... (odd rows— $\overline{CS}_A$ )  
 CLK-2: Rows 2, 4, 6... (even rows— $\overline{CS}_B$ )  
 Such that: CLK-2 = CLK-1

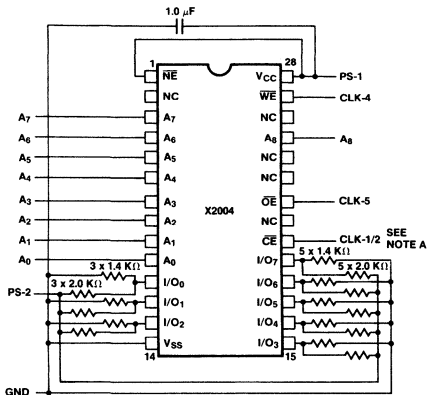
Figure 3a: X2210/2212 Burn-In Circuit



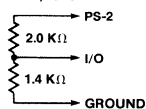
- Notes:** (1) A<sub>0</sub>-A<sub>7</sub>: binary sequencing address cycle: 40  $\mu$ s.  
 (2)  $\overline{STO}$  disabled (tied to V<sub>CC</sub> at device).  
 (3) V<sub>IN</sub> Low: 0.4V V<sub>IN</sub> High: 5.0V  
 (4) V<sub>CC</sub>: 5.50V  
 (5) X2210: A<sub>0</sub>-A<sub>5</sub> X2212: A<sub>0</sub>-A<sub>7</sub>

0072-3

Figure 3b: X2210/2212 Burn-In Timing

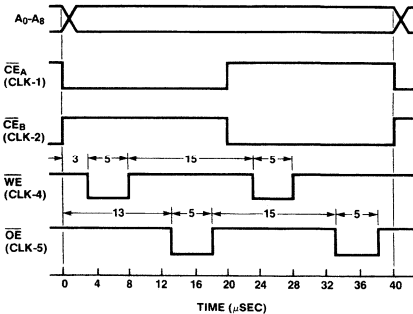


- Note A:** CLK-1: Rows 1, 3, 5... (odd rows = CE-A)  
 CLK-2: Rows 2, 4, 6... (even rows = CE-B)  
 CLK-2 = CLK-1
- Note B:** (1)  $\overline{NE}$  (Pin 1) must be hardwired to V<sub>CC</sub> (Pin 28) at device as shown.  
 (2) All resistors:  
 1% metal film  
 1/4 W  
 (3) All I/O's:



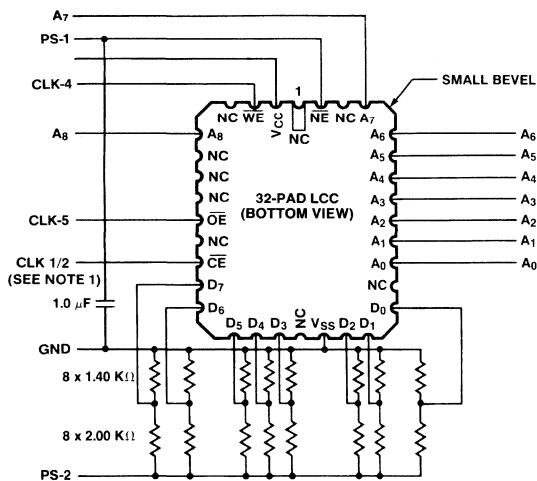
- (4) Socket-to-socket isolation as shown.

Figure 4a: X2004 (DIP) Burn-In Circuit



- Notes:** (1) A<sub>0</sub>-A<sub>8</sub>: binary sequencing cycle period: 40  $\mu$ s.  
 (2)  $\overline{NE}$  disabled (tied to V<sub>CC</sub> at device).  
 (3) Low state: 0.4V Max.  
 High state: 5.0V Typ.  
 V<sub>CC</sub>: 5.50V

Figure 4b: X2004 (DIP) Burn-In Timing



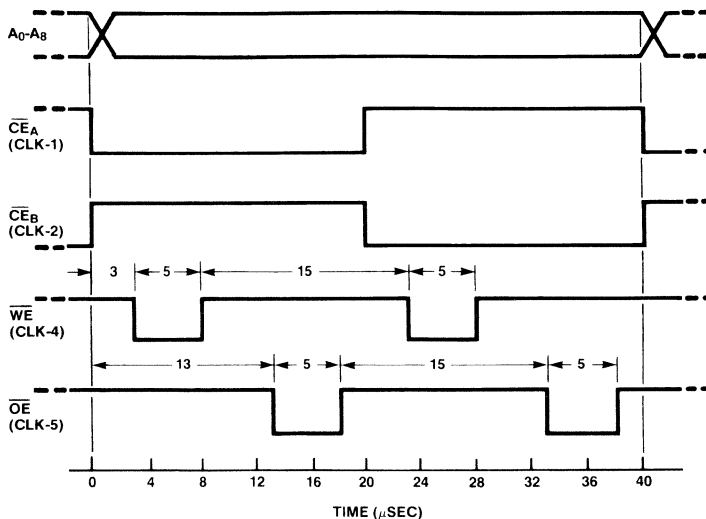
Note A: Pad Assignments

PAD	PAD
NC	1
NE	2
NC	3
A <sub>7</sub>	4
A <sub>6</sub>	5
A <sub>5</sub>	6
A <sub>4</sub>	7
A <sub>3</sub>	8
A <sub>2</sub>	9
A <sub>1</sub>	10
A <sub>0</sub>	11
NC	12
I/O <sub>0</sub>	13
I/O <sub>1</sub>	14
I/O <sub>2</sub>	15
V <sub>SS</sub>	16
NC	17
I/O <sub>3</sub>	18
I/O <sub>4</sub>	19
I/O <sub>5</sub>	20
I/O <sub>6</sub>	21
I/O <sub>7</sub>	22
$\overline{CE}$	23
NC	24
$\overline{OE}$	25
NC	26
NC	27
NC	28
A <sub>8</sub>	29
NC	30
$\overline{WE}$	31
V <sub>CC</sub>	32

- Note B: (1) CLK-1: All odd rows (No. 1, 3, 5 . . . )  
 CLK-2: All even rows (No. 2, 4, 6 . . . )  
 Such that: CLK-2 = CLK-1
- (2) Socket-to-socket isolation as shown.
- (3) Pad 2 ( $\overline{NE}$ ) must always be hardwired to V<sub>CC</sub> (Pad 32) at device.
- (4) All resistors:  
 1% metal film  
 1/4 W
- (5) I/O pull-up: 2.00 KΩ  
 I/O pull-down: 1.40 KΩ

Figure 5a: X2004 (LCC) Burn-In Circuit

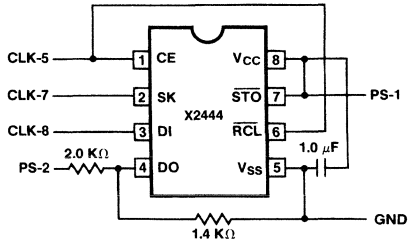
0072-7



- Notes: (1) A<sub>0</sub>-A<sub>8</sub>: binary sequencing cycle period: 40 μs.  
 (2)  $\overline{NE}$  disabled (tied to V<sub>CC</sub> at device).  
 (3) Low state: 0.4V Max.  
 High state: 5.0V Typ.  
 V<sub>CC</sub>: 5.50V

0072-8

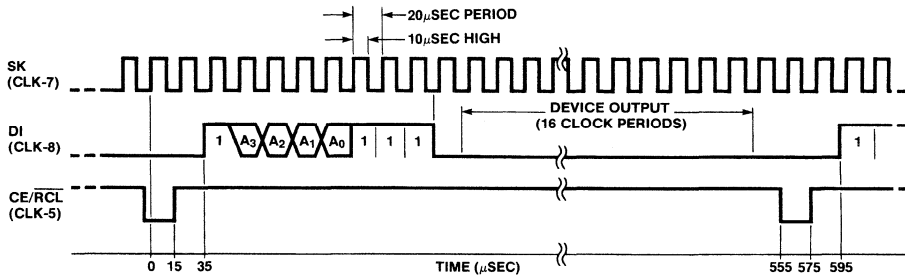
Figure 5b: X2004 (LCC) Burn-In Timing



- Notes:** (1)  $\overline{STO}$  (Pin 7) must be hardwired to  $V_{CC}$  (Pin 9) at device as shown.  
 (2) All resistors:  
 1/4 W  
 1% metal film  
 (3) Socket-to-socket isolation as shown.

Figure 6a: X2444 Burn-In Circuit

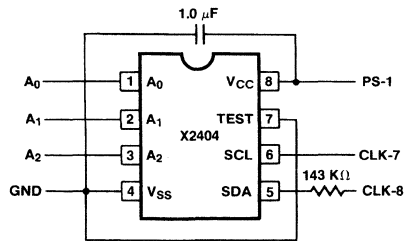
0072-9



- Notes:** (1)  $A_0$  through  $A_3$  binary count in data stream (10000111 through 11111111).  
 (2) All bits 20  $\mu$ s wide; 60  $\mu$ s between bytes.  
 (3)  $V_{CC}$ : 5.50V  $V_{IN}$  High: 5.00V  $V_{IN}$  Low: 0.4V Max.

0072-10

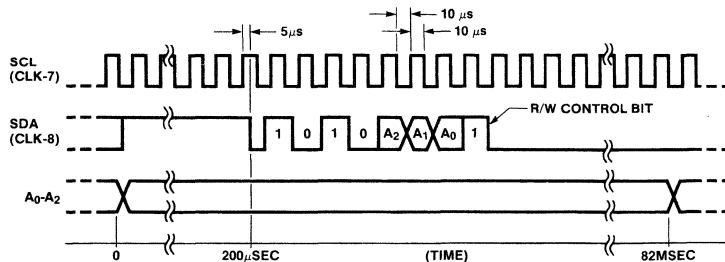
Figure 6b: X2444 Burn-In Timing



- Notes:** (1) Test (Pin 7) hardwired to  $V_{SS}$  (Pin 4) at socket.  
 (2) SDA (Pin 5) Socket-isolated as shown—143 KΩ resistor.  
 (3) Resistor: 1% metal film  
 1/4 W

Figure 7a: X2404 Burn-In Circuit

0072-11



- Notes:** (1) All addresses: binary sequencing.  
 (2) Device  $A_0$  cycle: 81.92 ms.  
 (3) SCL Period: 20.0  $\mu$ s (all bits: 20.0  $\mu$ s).  
 (4) Voltage levels:  
 $V_{IN}$  High = 5.0V  
 $V_{IN}$  Low = 0.4V Max.  
 (5)  $V_{CC}$  = 5.50V  
 (6) SDA serial data stream address state ( $A_0$ - $A_2$ ) must match parallel address lines state ( $A_0$ - $A_2$ ).

Figure 7b: X2404 Burn-In Timing

0072-12

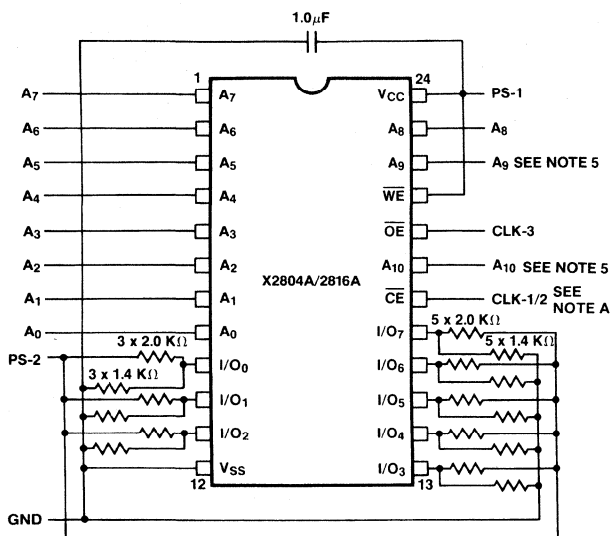


Figure 8a: X2804A/2816A (DIP) Burn-In Circuit

0072-13

**Note A:** CLK-1: Rows 1, 3, 5 ... (odd rows— $\overline{CE}_A$ )  
 CLK-2: Rows 2, 4, 6 ... (even rows— $\overline{CE}_B$ )  
 Such that: CLK-2 = CLK-1

**Note B:** (1)  $\overline{WE}$  must always be hardwired to  $V_{CC}$  (Pin 24) at device as shown.

(2) All resistors:  
 1% metal film  
 1/4 W

(3) I/O pull-up: 2.0 K $\Omega$   
 I/O pull-down: 1.4 K $\Omega$

(4) Socket-to-socket isolation as shown.

(5) Pin 19 ( $A_{10}$ ) and Pin 22 ( $A_9$ ) are no connects (NC) for the X2804A.

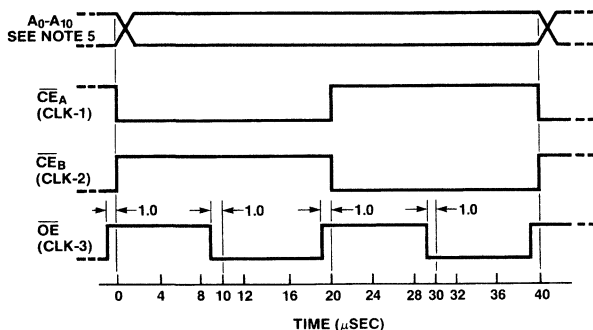


Figure 8b: X2804A/2816A (DIP) Burn-In Timing

0072-14

**Notes:** (1)  $A_0$ - $A_{10}$ : binary sequencing address cycle: 40  $\mu$ s.

(2)  $\overline{WE}$  disabled (tied to  $V_{CC}$  at device).

(3)  $V_{IN}$  Low: 0.4V  $V_{IN}$  High: 5.0V

(4)  $V_{CC}$ : 5.50V

(5) X2804A:  $A_0$ - $A_8$   
 X2816A:  $A_0$ - $A_{10}$

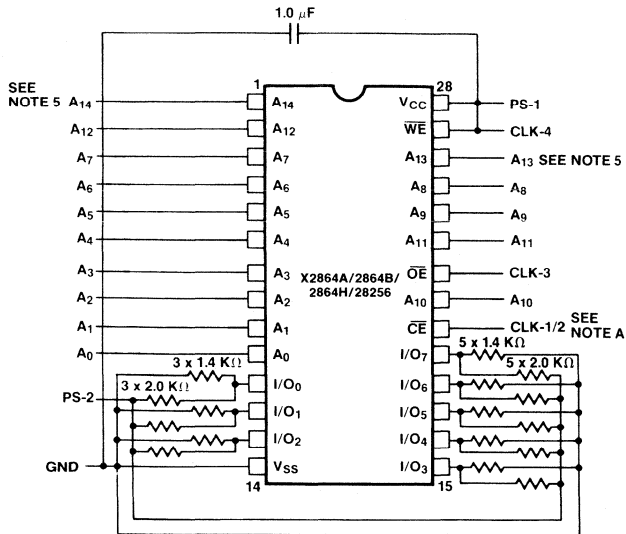


Figure 9a: X2864A/2864B/2864H/28256 (DIP) Burn-In Circuit

0072-15

**Note A:** CLK-1: Rows 1, 3, 5 . . . (odd rows— $\overline{CE}_A$ )  
 CLK-2: Rows 2, 4, 6 . . . (even rows— $\overline{CE}_B$ )  
 Such that: CLK-2 = CLK-1

**Note B:** (1)  $\overline{WE}$  must always be hardwired to  $V_{CC}$  (Pin 28) at device as shown.  
 (2) All resistors:  
 1% metal film  
 1/4 W  
 (3) I/O pull-up: 2.00 K $\Omega$   
 I/O pull-down: 1.40 K $\Omega$   
 (4) Socket-to-socket isolation as shown.  
 (5) Pin 1 ( $A_{14}$ ) and Pin 26 ( $A_{13}$ ) are no connects (NC) for the X2864A, X2864B, X2864H.

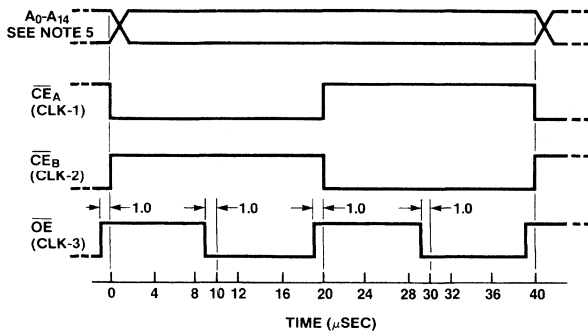
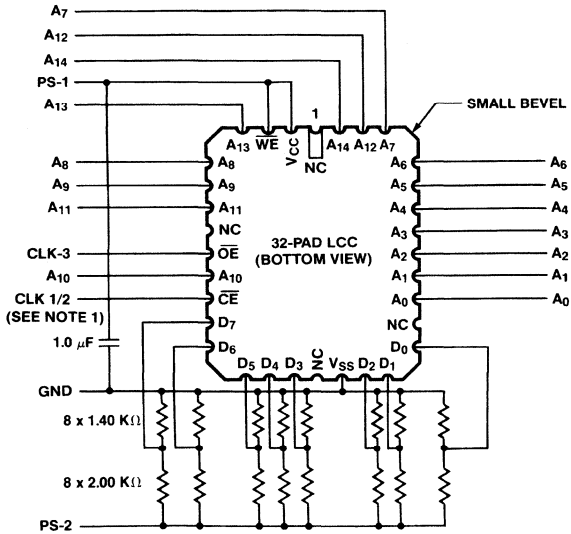


Figure 9b: X2864A/2864B/2864H/28256 (DIP) Burn-In Timing

0072-16

**Notes:** (1)  $A_0$ - $A_{14}$ : binary sequencing address cycle: 40  $\mu$ s.  
 (2)  $\overline{WE}$  disabled (tied to  $V_{CC}$  at device).  
 (3)  $V_{IN}$  Low: 0.4V  $V_{IN}$  High: 5.0V  
 (4)  $V_{CC}$ : 5.50V  
 (5) X2864A:  $A_0$ - $A_{12}$   
 X2864B:  $A_0$ - $A_{12}$   
 X2864H:  $A_0$ - $A_{12}$   
 X28256:  $A_0$ - $A_{14}$



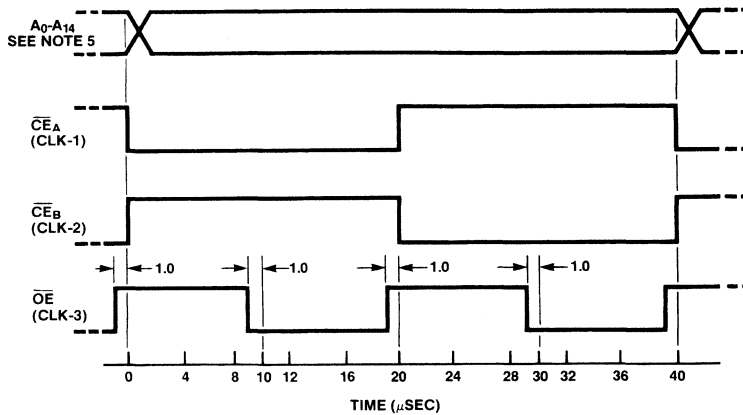
0072-17

Figure 10a: X2816A/2816B/2864A/2864B/2864H/28256 (LCC) Burn-In Circuit

**Note A: Pad Assignments**

PAD		PAD	
NC	1	NC	17
A <sub>14</sub> (X28256)	2	I/O <sub>3</sub>	18
A <sub>12</sub> (X2864A/X28256)	3	I/O <sub>4</sub>	19
A <sub>7</sub>	4	I/O <sub>5</sub>	20
A <sub>6</sub>	5	I/O <sub>6</sub>	21
A <sub>5</sub>	6	I/O <sub>7</sub>	22
A <sub>4</sub>	7	CE	23
A <sub>3</sub>	8	A <sub>10</sub>	24
A <sub>2</sub>	9	OE	25
A <sub>1</sub>	10	NC	26
A <sub>0</sub>	11	A <sub>11</sub> (X2864A/X28256)	27
NC	12	A <sub>9</sub>	28
I/O <sub>0</sub>	13	A <sub>8</sub>	29
I/O <sub>1</sub>	14	A <sub>13</sub> (X28256)	30
I/O <sub>2</sub>	15	WE	31
V <sub>SS</sub>	16	V <sub>CC</sub>	32

- Note B:** (1) CLK-1: All odd rows (No. 1, 3, 5 . . . )  
 CLK-2: All even rows (No. 2, 4, 6 . . . )  
 Such that: CLK-2 = CLK-1
- (2) Socket-to-socket isolation as shown.
- (3) Pad 31 (WE) must always be hardwired to V<sub>CC</sub> (Pad 32) at device.
- (4) All resistors:  
 1% metal film  
 1/4 W
- (5) I/O pull-up: 2.00 KΩ  
 I/O pull-down: 1.40 KΩ



0072-18

- Notes:** (1) A<sub>0</sub>-A<sub>14</sub>: binary sequencing address cycle: 40 µs.  
 (2) WE disabled (tied to V<sub>CC</sub> at device).  
 (3) V<sub>IN</sub> Low: 0.4V V<sub>IN</sub> High: 5.0V  
 (4) V<sub>CC</sub>: 5.50V  
 (5) X2816A: A<sub>0</sub>-A<sub>10</sub>  
 X2816B: A<sub>0</sub>-A<sub>10</sub>  
 X2864A: A<sub>0</sub>-A<sub>12</sub>  
 X2864B: A<sub>0</sub>-A<sub>12</sub>  
 X2864H: A<sub>0</sub>-A<sub>12</sub>  
 X28256: A<sub>0</sub>-A<sub>14</sub>

Figure 10b: X2816A/2816B/2864A/2864B/2864H/28256 (LCC) Burn-In Timing

**TABLE V: Thermal Resistance**

DEVICE	PACKAGE	PACKAGE TYPE	LEAD COUNT	$\theta_{ja}^*$	$\theta_{jc}^*$
X2210	D	Cerdip	18	55.0	18.0
X2212	D	Cerdip	18	55.0	18.0
X2004	D	Cerdip	28	33.5	16.5
X2004	E	LCC	32	46.5	5.0
X2444	D	Cerdip	8	TBD	TBD
X2404	D	Cerdip	8	TBD	TBD
X2804A	D	Cerdip	24	36.0	20.5
X2816A	D	Cerdip	24	32.0	18.0
X2816A	E	LCC	32	53.5	5.5
X2864A	D	Cerdip	28	35.0	16.5
X2864A	E	LCC	32	46.0	5.0
X2864A	G	LCC	32	TBD	TBD
X28256	D	Cerdip	28	23.0	2.5
X28256	E	LCC	32	47.0	2.0

\*Maximum value specified in °C/W.

The third line of the topside mark of each 883C compliant device provides complete fab run, assembly and screening lot traceability. This marking ap-

pears as a nine digit alphanumeric code following the electrostatic discharge sensitivity (ESD) identifier symbol of the inverted equilateral triangle:

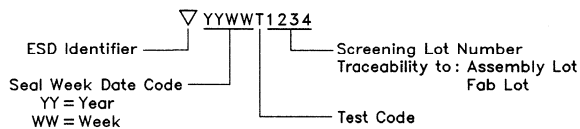


Figure 11: MIL-STD-883C Device Traceability

0072-19

The third line of the backside mark provides fab and assembly lot number traceability. This appears in a 12 digit alphanumeric code as follows:

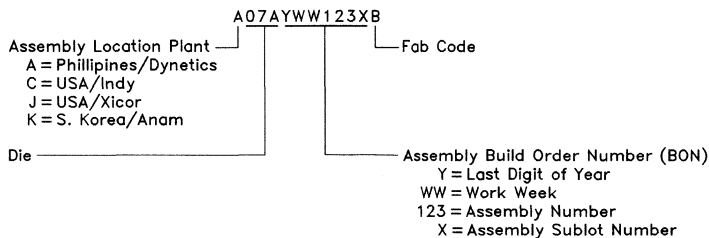


Figure 12: Assembly Location/Plant Codes

0072-20

---

## NOTES



## Application Notes

AN-101	Xicor NOVRAMs* Easier Than Ever to Use .....	7-1
AN-103	Xicor Replaces DIP Switches and Trimmers with NOVRAM* Memories .....	7-9
AN-105	The X2444 Serial NOVRAM* Teams Up with the 8051 Microcontroller Family .....	7-17
AN-106	E <sup>2</sup> POT™ Digitally Controlled Potentiometer Brings Microprocessor Control to Audio Systems—Adds Features .....	7-23

## Application Briefs

The Nine Most Frequent NOVRAM* Questions .....	7-33
Fourteen Common E <sup>2</sup> PROM Questions Answered .....	7-37
Nonvolatile Data Integrity: Inadvertent Write/Store Elimination .....	7-41
X2816A Design Allows Upgrade to X2864A and Beyond .....	7-45
Replacing DIP Switches with Nonvolatile Technology .....	7-49
Using DATA Polling in an Interrupt Driven Environment .....	7-53
E <sup>2</sup> PROM Provides the Solution to Field Alterable Software .....	7-57
Xicor E <sup>2</sup> PROMs vs. Battery Backed-Up CMOS RAMs Nonvolatile Memory Systems .....	7-61
E <sup>2</sup> PROMs: The Competitive Edge Against Bubble Memories .....	7-65
"tdv"—What is it? .....	7-69

## Article Reprints

5-volt-only EE-PROM mimics static-RAM timing .....	7-71
Understand your application in choosing NOVRAM, EEPROM .....	7-77
Non-volatile memories keep appliances out of the dark .....	7-89
Nonvolatile Memory Gives New Life to Old Designs .....	7-95
Save volatile data during power loss .....	7-103
Thick Oxide Beats Thin Film in Building Big EEPROMs .....	7-111
Solid-State Potentiometer .....	7-115
<b>Bit Maps for Xicor Products</b> .....	7-117



## NOVRAM\* Data Sheets

1

## Serial I/O Data Sheets

2

## E<sup>2</sup>PROM Data Sheets

3

## E<sup>2</sup>POT™ Digitally Controlled Potentiometer Data Sheets

4

## Die Products

5

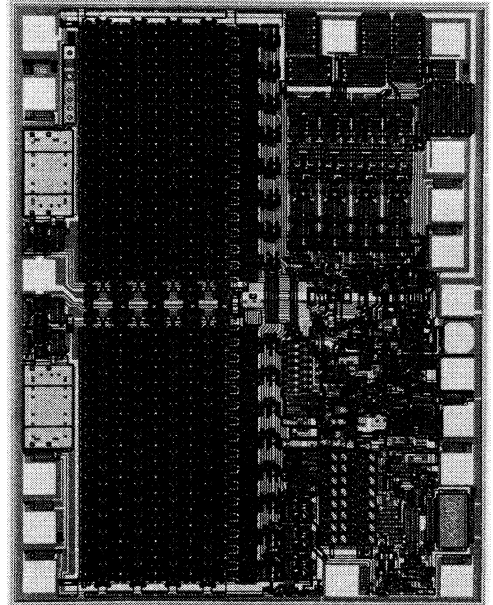
## Military

6

## Applications

7





0001-1

# **XICOR NOVRAMs\* EASIER THAN EVER TO USE**

**By Applications Staff**

**7**

\*NOVRAM is Xicor's nonvolatile static RAM device.

## Introduction

The purpose of this application note is to take the user through the internal operation of NOVRAMs as well as their external operation. These devices are finding their way into many diverse applications due to their ease of use. The major features of the XICOR family of NOVRAMs are 1) only 5 volts is required for all operations including programming, 2) only TTL signals are required and 3) all pulse widths are short ( $< 450$  ns).

Basically a NOVRAM is a memory device that has a static RAM overlaid with an EEPROM (Electrically Erasable Programmable ROM). The operation of the RAM is identical with other popular static RAMs such as the 2102A and the 2114. Figure 1 shows the block diagram of the XICOR NOVRAM family. NOVRAMs have  $\overline{CS}$  and  $\overline{WE}$  pins in common with their standard static RAM cousins but also have two additional control pins: STORE and RECALL. The STORE and RECALL pins control movement of data between the RAM and the EEPROM.

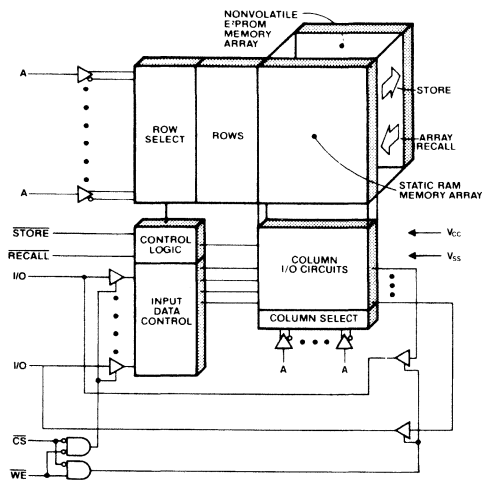


Figure 1) Block diagram of the XICOR NOVRAM family.

The STORE pin is used to transfer the contents of the RAM to the EEPROM in a single operation. The entire contents of the RAM are transferred with one STORE operation. After a STORE operation is completed the original data is still in the RAM as well as the EEPROM.

The RECALL pin is used to transfer the contents of the EEPROM back to the RAM. When this is done, whatever data were in the RAM prior to the RECALL

operation are totally replaced by the contents of the EEPROM. The STORE and RECALL operations function on the entire contents of the memory and not on a word by word basis. After either operation the contents of both the RAM and the EEPROM will be the same.

This may seem too good to be true; however, with XICOR's family of NOVRAMs the life of the systems designer is made even easier. Only a single five volt power supply is required for all operations including the STORE and RECALL operations. All addresses, data lines and control pins are TTL compatible and all pulse widths are short enough that most microprocessors do not require wait states. There are no high voltages or long pulse widths required which will inhibit the designer from designing a system with clean operation.

## Technology

The XICOR NOVRAM stores its nonvolatile data during periods of power off by the absence or presence of charges on floating polysilicon gates. This is the same structure that is widely used in UV-EPROMs. The floating gate is an island of polysilicon surrounded by oxides with thicknesses of about  $800 \text{ \AA}$ . Charge can be injected or removed from the floating gate by applying electric fields of sufficient strength to cause electron tunneling through the oxides. At normal field strengths the charges are permanently trapped on the floating gate even when power is removed.

The XICOR family of NOVRAMs uses three layers of polysilicon; the second layer is the floating gate. This structure employs a phenomenon known as Fowler-Nordheim tunneling. This form of tunneling is described in Vol. 40 No. 1 (Jan. 1969, pg. 278) of the Journal of Applied Physics and Vol. 27 No. 9 (Nov. 1975, pg. 505) of the Applied Physics Letters. In XICOR NOVRAMs this tunneling is enhanced by the use of textured polysilicon surfaces to generate higher field strengths at the surface to enhance electron injection into the oxide. The alternative to field enhancement by textured surfaces is to use ultrathin oxide layers in order to conduct the charge. The use by XICOR of standard oxide thickness gives XICOR a very manufacturable product, thus ensuring its low cost and volume delivery.

Figure 2. shows the circuit of the NOVRAM cell containing a conventional 6 transistor static RAM cell and a floating gate EEPROM cell with 2 additional transistors to control the action of data transfer. The floating gate (POLY 2) is connected to the rest of the circuit only through capacitance. Electrons are moved to the floating gate by tunneling from POLY 1 to POLY 2 and removed by tunneling from POLY 2 to POLY 3.

The capacitance ratios are the key to the operation of the transfer of data from RAM to EEPROM. If node

N1 is LOW, transistor Q7 is turned OFF. This allows the junction between CC2 and CC3 to float. Since the combined capacitance of CC2 and CC3 are larger than CP the floating gate follows the Internal Store Voltage node. When the voltage on the floating gate is high enough electrons are tunneled from POLY 1 to POLY 2 and the floating gate is negatively charged.

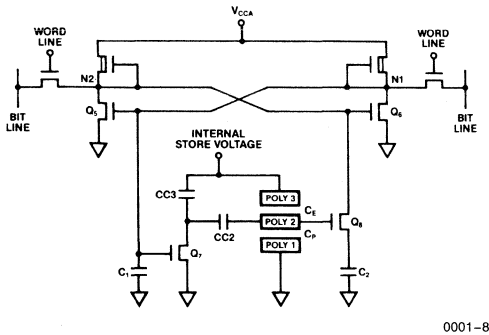


Figure 2) Circuit diagram of a NOVRAM cell.

If node N1 is HIGH, transistor Q7 is turned ON which grounds the junction between CC2 and CC3. Since CC2 is larger than CE, CC2 holds the floating gate near ground when the Internal Store Voltage node is pulled HIGH. This creates a sufficient field between POLY 2 and POLY 3 to tunnel electrons away from the floating gate leaving it with a positive charge.

The RECALL operation also takes advantage of capacitance ratios. The value of C2 in Figure 2 is larger than that of C1. When the external RECALL command is received, the internal power supply, VCCA, is first pulled LOW to equalize the voltage on N1 and N2. When the internal power node is allowed to rise, the node which has the lighter loading will rise more rapidly and the gain of the flip-flop will cause it to latch HIGH and the opposite node to latch LOW. If the floating gate has a positive charge C2, is connected to N2 through Q8 and N2 will latch LOW. If the floating gate has a negative charge Q8, is turned OFF and N1 will have the heavier loading.

## The Xicor NOVRAM Family

XICOR's family of NOVRAMs contains three members with identical operating characteristics. The three parts offer the designer a choice of memory organization. The X2201A, X2210 and X2212 are organized 1024 x 1, 64 x 4 and 256 x 4 respectively. All three devices are packaged in 18 pin DIPs with 300 mil

centers. Figure 3 shows the pin configuration of the three different NOVRAMs.

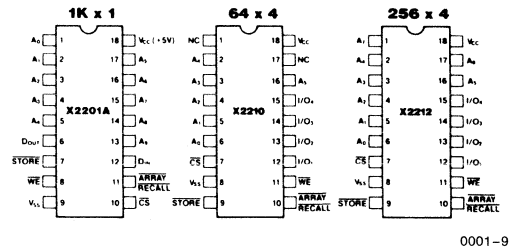


Figure 3) Pin configuration of the XICOR NOVRAM family.

The only functional difference between the three devices is that the X2201A has separate Data I/O lines while the two 4 bit wide parts have common I/O. Additionally, the X2210 and the X2212 are pin compatible. The two unused pins on the X2210 are used for the two higher order addresses on the X2212. The control pins STORE, RECALL, CS and WE operate identically on all three parts.

## Write Operation

The WRITE operation is initiated by applying valid addresses followed by both CS and WE going LOW. On the 300ns version access time version, at least one of these two signals must remain HIGH until the addresses are valid. CS and WE must remain LOW simultaneously for 100ns.

An easy way to look at this is to consider the internal write command as the simultaneous LOW of CS and WE. The internal write command is started by the last edge down and terminated by the first edge up. Valid addresses must overlap this internal write command. Data must be referenced to the first positive edge of CS or WE. The timing required for writing to the RAM is shown in Figure 4.

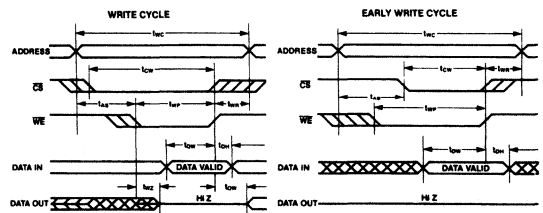


Figure 4) Timing diagram for Writing to the RAM.

## Read Operation

The READ operation is the easiest of the four operations performed by the NOVDRAM. In the case of the 300ns access time version, data will be valid at the outputs 300ns after valid addresses or 200ns after CS goes LOW, whichever is later.

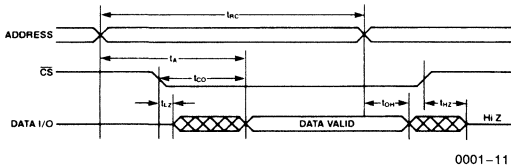


Figure 5) Timing diagram for Reading from the RAM.

## Store Operation

The STORE operation is initiated by the application of an active LOW TTL pulse of 100ns or greater on the STORE pin. As long as the power supply remains within its specification for 10ms after the beginning of the STORE pulse the contents of the RAM will have been transferred to the EEPROM in total. The STORE operation cannot be terminated once initiated except by removing the power supply. This can not be counted upon to rapidly terminate the STORE operation since the user cannot determine how far the STORE operation the device has progressed. Additionally, if the power supply drops below the specification during the 10ms the integrity of the STORE operation is not assured. Figure 6 shows the timing diagram for transferring data from the RAM to the EEPROM.

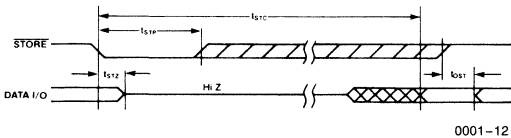


Figure 6) Timing diagram for the STORE operation where data is transferred from the RAM to the EEPROM.

The STORE operation takes precedence over all other operations except the RECALL operation. If the RECALL operation has begun, any STORE command is ignored as long as the RECALL pin remains LOW. Once the STORE operation has started, taking the RECALL pin LOW has no effect and the STORE operation will be completed. If a READ or WRITE cycle is in progress when a STORE command is received, that cycle is terminated. The data in the selected RAM

address during an interrupted WRITE cycle would be indeterminate.

During the 10ms of the STORE operation the NOVDRAM should not be accessed for any other operation as it would not be known if the internal STORE operation was completed or not. If the internal STORE operation was completed before the 10ms and another operation command was entered, that command would be executed. However, if the internal STORE operation was not completed and another operation command was received, the later command would be ignored. During the STORE operation the outputs of the NOVDRAM are in the floating state.

## Recall Operation

The RECALL operation is initiated by the application of an active LOW TTL pulse of 450ns or greater on the RECALL pin. The positive going edge of this pulse determines when it is possible to read data from the RAM. Valid data from the RAM can be viewed on the outputs of the NOVDRAM 750ns after the rising edge of RECALL or 300ns after application of valid addresses, whichever comes latest. FIGURE 7 shows the timing requirements for transferring data from the EEPROM to the RAM.

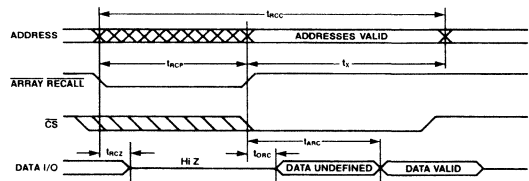


Figure 7) Timing diagram for the RECALL operation.

The RECALL operation takes precedence over all other operations. RECALL will terminate a READ or WRITE cycle if applied in the middle of either cycle. The RECALL operation can take precedence over the STORE operation only if the RECALL command was received prior to the STORE command.

## Hooking up the NOVDRAM

Now that the basics of the four NOVDRAM operations have been described, we may discuss using these unique parts in a system. Let's first discuss a system in which we connect the NOVDRAMs to a 6502. We'll assume that the system powers up and down cleanly. The problem of systems where this does not occur will be dealt with later.

The 6502 microprocessor uses memory space for I/O functions. The design uses one set of addresses for the READ and WRITE operations and other blocks of addresses to initiate the STORE and RECALL operations. An APPLE II\* computer was used as the 6502 computer because it has address space already decoded for I/O functions and convenient card slots to communicate with these decoder outputs.

The RAM was placed in the address space starting at HEX address \$C800 by connecting pin 20 on the APPLE II peripheral connector to the CS on the NOVRAM. This pin is activated when any of the 2048 bytes starting at \$C800 are accessed. Peripheral slot 2 was selected for the NOVRAM design. On slot 2 pin 41 is activated whenever the 16 bytes located at HEX address \$C0A0 are accessed. This address space is sent only to slot 2 and was tied to the STORE pin on the NOVRAM. PIN 1 also has a unique address space for slot 2 and was tied to the RECALL pin. This space is the 256 bytes starting at HEX address \$C200.

Figure 8 shows the connections of the card to be plugged into peripheral card slot 2. Reading and writing are accomplished from the BASIC programming language by PEEK and POKE instructions to HEX addresses starting at \$C800. The STORE operation is called by either a PEEK or a POKE instruction to any of the 16 addresses starting at \$C0A0. RECALL is initiated by accessing any of the 256 bytes starting at \$C200.

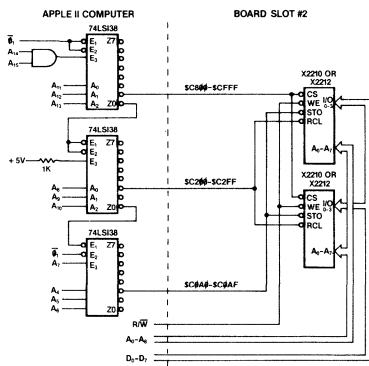


Figure 8) Connections for operating the NOVRAM on the I/O Bus of an APPLE II computer.

The APPLESOFT\* program in Table 1 demonstrates how a NOVRAM can be accessed easily. The statement 210 is a Write operation to HEX address \$C200 while statement 310 is a Write to HEX address \$C0A0. The CS pin is activated with statement 430 and state-

ment 580 respectively. This program was written for the X2210 but it could be easily modified for the X2212 or even eight X2201s.

```

5 TEXT : HOME
10 A$ = "#1 WELCOME TO THE WORLD
  S EASIEST TO USE NONVOLATILE
  STATIC RAM!"
20 B$ = "#2 ONLY A SINGLE 5 VOLT
  POWER SUPPLY IS REQUIRED FOR
  OPERATIONS!"
30 C$ = "#3 ALL INPUTS AND OUTPUT
  S REQUIRE ONLY TTL INTERFAC
  E SIGNALS!"
40 F$ = "#4 ALL TIMING SIGNALS AR
  E MICROPROCESSORCOMPATIBLE-N
  O STRETCHING!"
50 G$ = "#5 5 SIZES AVAILABLE: (X2
  201)024X1, (X2212)256X4
  ,(X2210)64X4"
60 VTAB $: HTAB 11: PRINT "XICOR
  'S X2210 DEMO"
75 PRINT : PRINT : HTAB 5: PRINT
  "1=RECALL": HTAB 25: PRINT
  "2=READ"
80 PRINT : HTAB 5: PRINT "2=STOR
  E": HTAB 25: PRINT "4=WRITE"
85 PRINT : HTAB 17: PRINT "5=EXI
  T"
90 VTAB 15: HTAB 12: INPUT "SELE
  CT ONE (1-5)
100 IF A < 1 OR A > 5 THEN HOME
  : VTAB 5: HTAB 5: PRINT "ONL
  Y 1-5 ALLOWED---TRY AGAIN": GOTO
  75
110 ON A GOTO 200,300,400,500,60
  0
200 REM *****
201 REM * RECALL SUBROUTINE *
202 REM *****
210 POKE -15972,0
215 HOME : VTAB 5: HTAB 14
216 PRINT "RECALL COMPLETE"
218 FOR I = 1 TO 1000: NEXT I
220 HOME : GOTO 60
300 REM *****
301 REM * STORE SUBROUTINE *
302 REM *****
310 POKE -16224,0
315 HOME : VTAB 5: HTAB 14: PRINT
  "STORE COMPLETE"
320 FOR I = 1 TO 1000: NEXT I
325 HOME : GOTO 60
400 REM *****
401 REM * READ SUBROUTINE *
402 REM *****
422 HOME
423 VTAB 5: HTAB 12: PRINT "RESU
  LTS FROM RAM": PRINT : PRINT
425 FOR I = 1 TO 64
430 PRINT CHR$(PEEK(-14336
  + I)):
435 NEXT I
440 FOR I = 1 TO 5000: NEXT I
445 HOME : GOTO 60
500 REM *****
501 REM * WRITE SUBROUTINE *
502 REM *****
505 HOME : VTAB 5: HTAB 6: PRINT
  "PRESELECTED MESSAGE (1-5)"
  : PRINT : PRINT
515 PRINT : PRINT : HTAB 4: PRINT
  "ENTER MESSAGE FROM KEYBOARD
  (4)"
520 PRINT : PRINT : HTAB 11: INPUT
  "SELECT ONE (1-6)?:"A
525 ON A GOTO 531,532,533,534,53
  5,540
531 G$ = A$: GOTO 548
532 G$ = B$: GOTO 548
533 G$ = C$: GOTO 548
534 G$ = F$: GOTO 548
535 G$ = G$: GOTO 548
540 PRINT : PRINT : HTAB 5: PRINT
  "INPUT MESSAGE-64CHARACTERS
  MAX": INPUT G$
545 G$ = G$ + "
  "
548 HOME : VTAB 5: HTAB 12: PRINT
  "WRITTEN INTO RAM": PRINT : PRINT
550 G$ = LEFT$(G$,64)
570 FOR I = 1 TO 64
575 Z$ = MID$(G$,I,1):Z = ASC
  (Z$)
580 POKE -14336 + I,Z
582 PRINT Z$
585 NEXT I
590 FOR I = 1 TO 5000: NEXT I
595 HOME : GOTO 60
600 END

```

Table 1) An APPLESOFT BASIC program for demonstrating the four operations of NOVRAMs.

\* APPLE II and APPLESOFT are trademarks of Apple Computers.

## Protection Against Inadvertent Store

The circuit described in the previous section assumes that the system is powered up and down in an orderly manner. This would mean that the microprocessor would never generate addresses unless they were part of the program. Unfortunately real systems do not operate in this ideal manner. Although the circuit described above has not produced a fault during extensive testing, the possibility exists that the hex addresses \$C0A0-\$C0AF could come up during power up, or during a brown out when the supply dropped below the operating specification, or during a power failure.

Several methods can be used to insure that the NOVRAM does not react to errors produced by the system when it is out of its operating specification. Setting the **RECALL** pin LOW to block a STORE operation is the easiest. Holding the **STORE** pin between  $V_{IH\ MIN}$  and the falling power supply is another.

Most microprocessors are not totally under control for the first few cycles after power up. Their early addresses depend on what is in the registers after the System Reset pulse terminates. There is a possibility that these registers can cause one of the early addresses to be the same selected for a STORE operation. In this case the circuit shown in Figure 8 could cause the EEPROM to be written with false data during the power up operation. Figure 8 allows the STORE operation to be initiated if any of 16 addresses is selected for either a read or a write.

Although microprocessors can put out uncontrolled addresses they do not put out uncontrolled write commands. By ANDing the System Write line with the System STORE command, the NOVRAM would recognize a STORE operation only on a machine write cycle.

A potential danger in the use of the above schemes is the fact that three state TTL gates are not under total control while the power supply is coming up. This could produce glitches on the STORE pin even though no Write command was received at the input of the gate. A more positive way to insure that the STORE pin follows the power supply as the voltage increases is to use an open collector NAND gate with one of the inputs provided by a signal that determines power supply status (Circuitry for power supply status will be covered later in this application note). If one input of an open collector NAND gate is held LOW the output transistor is turned OFF since it can not receive base current. Pulling the output of this gate to the power supply of the NOVRAM through a pullup resistor will then insure that the output follows the power supply with no glitches.

Carrying the use of a power supply status signal one step further, would be to use it to hold the **RECALL** pin LOW in addition to holding the **STORE** pin HIGH. A dir-

ect connection of this status signal to the **RECALL** pin is all that is necessary as shown in Figure 9. This circuit has a more positive control of the NOVRAM since it takes two actions to prevent an inadvertent STORE operation.

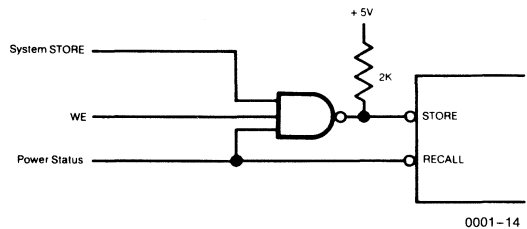


Figure 9) A power supply status line held LOW can insure that both the **RECALL** pin is held LOW and the **STORE** pin is held HIGH.

An example of a basic circuit to monitor the power supply status is shown in Figure 10. The output of this two-stage circuit is held LOW whenever the power supply is below 4.5 Volts. This same technique can be used with a Zener diode and an operational amplifier. The designer is cautioned to consider temperature effects.

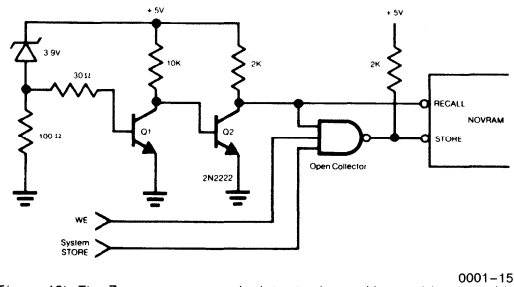


Figure 10) The Zener power supply detector is used in combination with the open collector on the **STORE** pin to provide protection against an inadvertent STORE operation during power up and power down.

Another method of power supply status is to assume that the only power supply fault which requires insuring that wrong data is not stored is the loss of the AC line voltage. Many commercially available AC line fault monitors are on the market. Two of these line fault monitors are the MID 400 Power Line Monitor from General Instrument and the SG1547 from Silicon General. Additionally, many commercially available power supplies have a power fail signal either as a standard feature or as an option.

The circuit shown in Figure 11 shows another type of power supply status detector. This circuit is a low cost solution but it should be used only to take the **RECALL**



pin LOW because it does not provide adequate drive for a TTL gate.

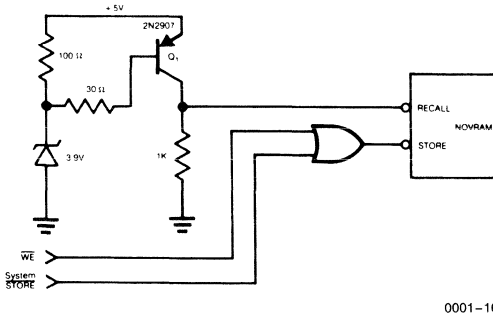


Figure 11) Another form of power supply status detector to drive the RECALL pin LOW when the supply drops below 4.5Volts.

Some other schemes to protect against inadvertent STORE operations are the use of jumpers, cables and/or switches. The STORE signal is transmitted through the jumper or switch which is normally open unless it is desired to change the data in the EEPROM. During normal operation the only component attached to the STORE pin is a resistor to the power supply.

A more comprehensive discussion of power supply status circuitry can be found in XICOR's Ap Note #102. This note covers those requirements that STORE data at power failure.

## Applications

Most microprocessor systems have need for some form of nonvolatile memory to store important data such as:

- 1) Calibration constants
- 2) Set-up configuration information
- 3) User system ID
- 4) Changeable programs/firmware
- 5) System status
- 6) Accounting information
- 7) Error conditions

The types of equipment that are today being designed to include NOVRAMs vary through the complete line of electronic equipment. Some of these systems are:

- 1) Computer peripherals/terminals etc.
- 2) Automatic tellers/transaction terminals
- 3) Point-of-sale terminals
- 4) Smart scales
- 5) Vending machines and games (i.e. arcade games, slot machines)

- 6) Meters (i.e. utilities, taxi, gas pumps)
- 7) Process control
- 8) Robots
- 9) Instruments (musical, medical, test, avionics)
- 10) Communications
- 11) Transducers/load cells
- 12) Automotive: odometers, engine control
- 13) Office equipment: copiers, word processors
- 14) Military products

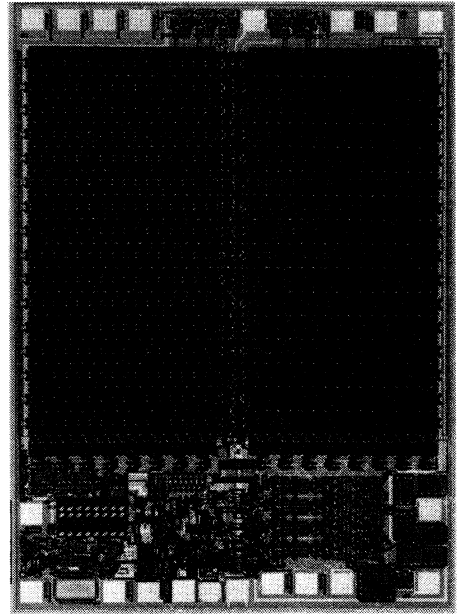
Some of the competitive products being replaced by NOVRAMs in systems are:

- 1) DIP switches
- 2) Thumbwheel switches
- 3) CMOS with batteries
- 4) EAROM
- 5) EEPROM
- 6) Potentiometers

One should let his imagination soar when thinking applications for these unique NOVRAMs. XICOR is always interested in application ideas that represent both normal and off-beat uses of these NOVRAMs. Any ideas sent to XICOR will be greatly appreciated.

---

## NOTES



0002-1

# **XICOR REPLACES DIP SWITCHES AND TRIMMERS WITH NOVDRAM\* MEMORIES**

**By Applications Staff**

**7**

\*NOVDRAM is Xicor's nonvolatile static RAM device.

## Introduction

The desire to replace mechanical components in electronic systems for purposes of increased reliability, lower costs and ease of maintainability has spread to DIP switches and trimming potentiometers or trimmers. The component that makes this replacement possible is the NOVRAM memory from Xicor. The NOVRAM memory is a device that has two memories in parallel, a standard static RAM and a nonvolatile electrically erasable programmable read only memory (EEPROM). The EEPROM portion of the NOVRAM memory holds data that is equivalent to the settings of the now obsolete DIP switches and trimmers.

## What Is A NOVRAM Memory?

A NOVRAM memory, as stated previously, is two memories in a single unit. The standard static RAM has a nonvolatile EEPROM cell associated with each RAM cell. Figure 1 shows a block diagram of a typical NOVRAM memory.

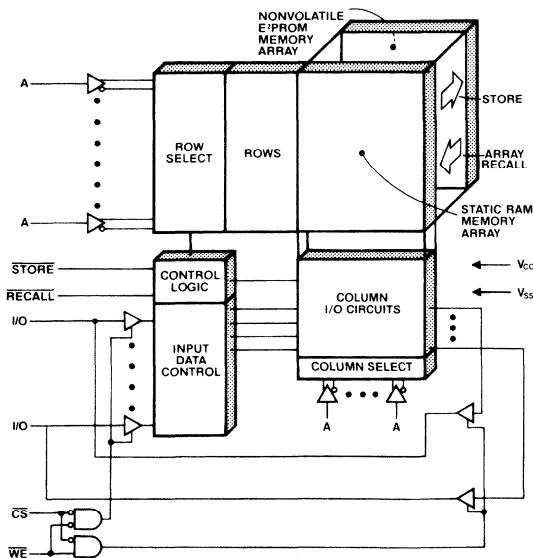


Figure 1) NOVRAM memory block diagram.

There are two additional pins on a NOVRAM memory device that do not appear on an ordinary static RAM. These two pins are called **STORE** and

**RECALL**. The **STORE** pin is used to transfer the entire contents of the RAM to the EEPROM as a single block. This operation is performed in parallel. The **RECALL** pin is used to transfer the entire contents of the EEPROM back to the RAM. At the end of either operation, the contents of the two memories are identical.

Access to the EEPROM data is through the RAM portion. To alter the contents of the EEPROM, the data must first be written into the RAM and then transferred to the EEPROM with a Store operation. To use the contents of the EEPROM in the system, perform a Recall operation and then the contents of the RAM may be read. Once data is stored in the EEPROM, the RAM can be used as an entirely separate and independent memory. Some users put configuration data into the EEPROM and then use the RAM as a separate scratchpad.

Besides these operational features, the NOVRAM memory has some unique electrical features. These devices are the world's easiest-to-use nonvolatile components in that they operate with only a single 5-volt power supply, simple TTL level pulses and short pulse widths (< 450 ns). Even for operations such as the Store operation, which takes 10 ms to complete, it only requires a low level TTL pulse of 100 ns or greater to initiate. During the remaining time, the NOVRAM memory is not on the bus, which frees the microprocessor and the bus for other tasks. Complete details of the operation of NOVRAM memories can be found in the individual data sheets and application note AN101.

## Replacing DIP Switches With NOVRAM Memories

DIP switches and thumbwheel switches have been used in systems to provide alterable, nonvolatile data. Some uses of this data are to set up configuration parameters and to provide calibration constants. The apparent low cost of these components is one of their attractive features. The drawback is that costs of these components do not end with installation.

The biggest cost of these mechanical, nonvolatile components is in post-installation service. A simple change of a DIP switch setting can require a technician to visit the equipment, disassemble the unit, throw the switch and reassemble the equipment. This could easily run the total use costs to well over 10 times the installed cost. A solution to the problems presented by DIP switches is to use a NOVRAM memory to hold valuable configuration or calibration data. In addition to a lower-cost, easier, and more secure method of changing data, NOVRAM memories cost less at the installed level.

The disadvantages of using DIP switches in modern electronic systems accumulate through each step of the manufacturing process. The first stage of NOVRAM memory advantages starts right at system concept and design. Since the density of NOVRAM memories is significantly greater (up to 1024 switches in a single low-cost DIP package), more functional options can be added to enhance the total value of the system. Features such as electronic unit type signature can be added for a small software cost, with no extra components. No special access needs to be provided to change the NOVRAM memory, as all changes can be made from a keyboard or over phone lines. This can not be said for DIP switches, which require disassembly or special doors or hatches to provide access.

At incoming inspection it is difficult to completely test a package of DIP switches for all possible combinations, or even as individual switches. The NOVRAM memory, on the other hand is tested by automatic test equipment both quickly and thoroughly. The NOVRAM memories are 100% tested by Xicor and can be further tested at whatever levels the user desires, including the quick testing of all the options that were designed into the equipment. In the case of the DIP switch, this would require manually setting each option, rather than have the final system test equipment take care of the task.

The assembly operation is made more difficult when trying to wave solder or clean a board containing DIP switches. These operations can cause contamination in the degreasing step. This is true, even on the components that have tape or other cover for protection, as these are extra items to handle or become lost. Again, the NOVRAM memory exhibits none of these problems in that they are in sealed packages like the rest of the semiconductor components that make up the bulk of the system.

Once the system is in the field, the advantages of the NOVRAM memory are further enhanced. The basic reliability improvement of semiconductors over mechanical components is well known. Equipment warranties can be enforced since there is no need for a customer to open the equipment. The greatest advantage of all comes in service. No longer is it necessary for a technician to travel to the users site to change the setting on DIP switches as this can be accomplished over a phone hookup.

In addition to all of the above cost savings and system benefits in using NOVRAM memories, the basic component cost is also very low. Figure 2 shows a typical interface for DIP switches in a microprocessor system. Each package of 8 switches requires a decoder port and 8 diodes to provide isolation from other switches.

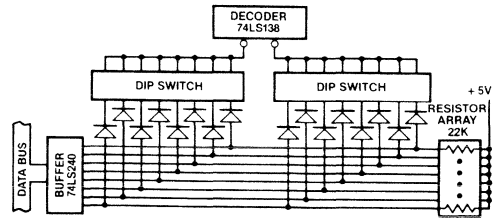


Figure 2) Typical DIP switch interface for multiple packages

An octal buffer and 8 pull up resistors are required for any quantity of switch packages in a given system. Matrix schemes could be applied to reduce the decoder ports at the cost of more buffers but, by then, the costs will be much greater than those of using NOVRAM memories.

The assembly costs include incoming inspection, handling, inventory, board real estate, and final inspection. These costs are variable depending on volume and other factors.

The interface of a NOVRAM memory to a microprocessor is shown in Figure 3.

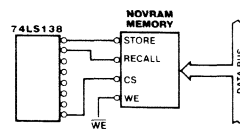


Figure 3) The typical NOVRAM memory interface requires only 3 decoder ports for any number of switches up to 1024.

This setup requires 3 decoder ports for any number of switches up to 1024 and then starts adding a single port for each additional package of 256 or 1024 switches.

The plot in Figure 4 shows that system costs using NOVRAM memories remain constant as the equivalent packages of DIP switches required are increased. These costs include the costs of all associated components, assembly and testing.

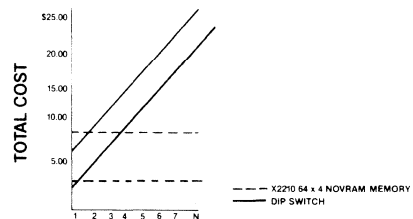


Figure 4) Relative costs of using NOVRAM memories as opposed to DIP switches as a function of packages of 8 switches required.

7

The plot shows that whenever the required number of DIP switch packages of 8 switches exceeds 1, the NOVRAM approach is lower in cost at the systems level.

The cost of using DIP switches rises constantly as the number of required packages increases. An actual cost crossover occurs between 1 and 2 packages of 8 switches. Designers can derive their actual costs by calculating the two approaches based on the costs at their firm. These costs should include, in addition to the component costs, all costs associated with incoming inspection, warehousing, assembly and system tests. One will find that the crossover between 1 and 2 packages of 8 switches is consistent and favors the NOVRAM memory approach.

## Where And Why Trimmers Are Used

The trimming potentiometer or trimmer is a 3-terminal device that can be connected in many different configurations. The purpose of the trimmer in the analog circuit is to make a fine adjustment of a current or a voltage. This current or voltage is then used in analog circuits to compensate for component variations in frequency, gain, offset, voltage or current.

Like the DIP switch, the trimmer appears quite inexpensive when one considers only the purchased price. In actuality it can be one of the most expensive components on the card when the costs of field calibration are taken into consideration. It takes only one service call (considered by some to cost approximately \$200) due to a changed setting caused by vibration, humidity or even well-intentioned user tampering, to run the cost of using the trimmer to high levels. In addition, the trimmer requires equipment disassembly and the skilled use of a screwdriver. This skill adds to the cost of owning the equipment.

Taking an 'all costs considered' approach is one way manufacturers are reducing the cost of equipment ownership as a function of performance. Although the end customer wants equipment that is low in purchase price and service costs while delivering a high level of performance, they will purchase a more expensive piece of equipment if they believe that the service costs and possible downtime will be reduced.

The functions of the trimmer can be duplicated quite well by a NOVRAM memory combined with a Digital-to-Analog Converter (DAC). A DAC is a device that delivers a voltage at the output that is a function of a digital signal at the input. In a microprocessor system, this is a variable voltage source that is under the

control of the program. While the DAC cannot exactly duplicate the 3 terminals of the trimmer, the circuit can be modified to provide equivalent results.

The NOVRAM memory provides settings for the DAC that are free from problems of humidity and vibration, as well as holding onto those settings during times of no power. Once the NOVRAM memory/DAC combination is in the circuit, the calibration can be made automatic by closing the loop since all mechanical adjustments are eliminated. A self-calibrating system can eliminate all expensive service calls for recalibration.

## Duplicating The Function Of The Trimmer

This section will demonstrate a few simple concepts for using a NOVRAM memory and a DAC in combination to modify important circuit parameters. As previously mentioned, a trimmer adjusts small variations of frequency, gain, offset, voltage or current. By properly interfacing the output voltage of a DAC in the analog circuit, these functions can be easily duplicated.

The first example shown will demonstrate how to effect a small adjustment in voltage that can be used as a reference or for some other need. Figure 5 shows an operational amplifier connected to provide a small amount of trim to the output. The 9.9k and 100 ohm resistors provide a division by 100 of the DAC output.

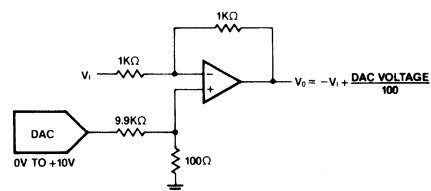


Figure 5) The DAC output provides up to 100 millivolts of trim for the operational amplifier output voltage.

If the DAC can be adjusted from 0 to 10 volts, this voltage divider provides an offset of up to 100 millivolts. The operational amplifier offset adds this amount to the output, providing up to 100 millivolts of reference voltage trim.

The next example will show how to provide a small offset for a fixed gain amplifier. Figure 6 shows the operational amplifier connected as an inverting amplifier with a gain of 10.

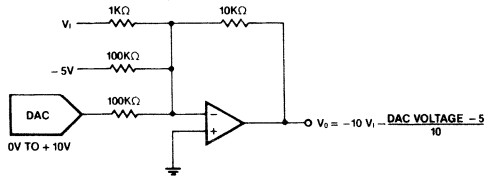


Figure 6) The DAC output provides an offset of 0.5 volt for a fixed gain amplifier.

The fixed gain is established by the 1K and 10K resistors. As the DAC output is varied from 0 through 10 volts, this voltage, combined with the -5 volts, reduces the amplifier output by  $1/10$  of the difference. This gives a fixed offset of up to 0.5 volt in either direction.

The third example will show a different use of a DAC to change the operational amplifier gain. This example uses a CMOS DAC with the ladder network in the amplifier feedback loop.

A short course in CMOS DACs is in order at this time. Figure 7 shows a simple 3-switch CMOS DAC.

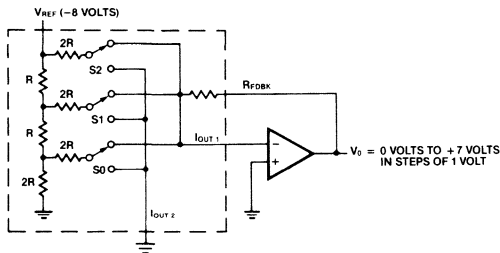


Figure 7) A simplified 3-switch CMOS DAC.

The outputs of a CMOS DAC are in the form of current. The sum of the two output currents is always a constant. In the case of Figure 7, this sum is  $1/8 \times V_{REF}/R$ . Both current outputs must look into a ground potential. In Figure 7 the  $I_{OUT1}$  pin is tied to the summing junction of an operational amplifier while the  $I_{OUT2}$  pin is tied to system ground. The internally provided feedback resistor should be used with an amplifier since its temperature coefficient is identical to the other resistors on the DAC chip. The DAC switches are operated by standard 5 volt logic levels. The amplifier output in Figure 7 will vary from 0 to 7 volts in 1 volt increments depending on the setting of switches  $S_0$ ,  $S_1$  and  $S_2$ . These switches in the 'up' position add 1, 2 and 4 volts, respectively, to the amplifier output. In the positions shown, the amplifier output is 7 volts.

Figure 8 shows the CMOS DAC of Figure 7 in a slightly different configuration.

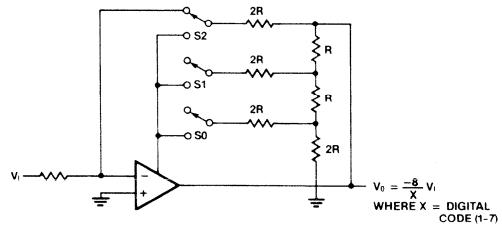


Figure 8) A CMOS DAC used in the amplifier feedback loop to adjust the amplifier gain.

The ladder network provides the feedback to the amplifier while the internal feedback resistor is used as the input resistor. If one goes through the equations, the result for Figure 8 is  $V_O = V_I \times 8/\times$ , where  $\times$  is the digital code for the switch settings from 1 to 7. The circuit gain runs from a low of  $8/7$  for the switches in the indicated position, to a gain of 8 when  $S_0$  is high and the other switches are low. Table 1 shows a listing of the gains obtainable.

S2	S1	S0	GAIN
L	L	H	8
L	L	L	4
L	H	L	$2\frac{2}{3}$
L	L	L	2
H	L	L	$1\frac{3}{5}$
H	L	L	$1\frac{1}{3}$
H	H	L	$1\frac{1}{2}$

Table 1) Gains of the circuit in Figure 5 as a function of the switch settings.

## Analog Circuit Examples

This section will present some actual circuit examples for using a NOVRAM memory combined with a DAC. The circuits that appear in this section have been built and tested. The concepts presented may be useful to stimulate ideas which will help to solve the reader's system problems and may even be of immediate use. Figure 9 shows how the NOVRAM memory/DAC combination provides a voltage or a current for the application.

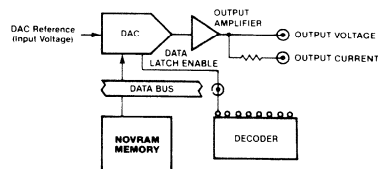


Figure 9) A NOVRAM memory DAC combination provides a voltage or a current to correct analog circuits.

It is, of course, possible for a single NOVRAM memory to provide the address setting for multiple DACs. The DAC size used is selected for the user's application, depending on the accuracy and resolution required. There are even multiple DACs available in a single package such as the SAB 3013 from Philips for more cost sensitive applications.

## Tuneable Crystal Oscillator

The first application example of a NOVRAM memory used in combination with a DAC is that of a quartz crystal oscillator. These circuits find application in many areas, including aviation and nautical navigation, as well as time measuring due to high stability. The oscillator is normally trimmed with a small padding capacitor in shunt or series with the crystal. This trim is used to 'pull' the resonance point of the crystal by a few parts per million (PPM) to set the operating frequency of the circuit. The capacitor may have to be adjusted in the field to retrim for the aging effects of the crystal and its associated circuitry.

The circuit in Figure 10 uses a NOVRAM memory/DAC combination to provide the trim voltage for a varactor.

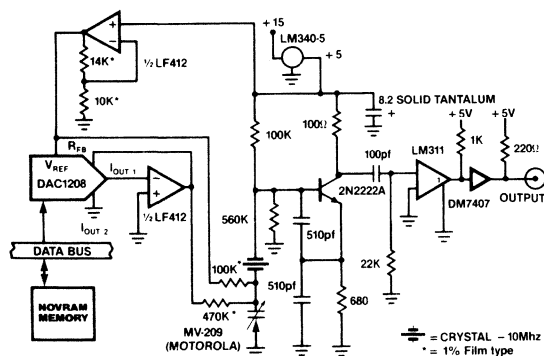


Figure 10) Tuneable crystal oscillator.

A varactor is a diode whose capacitance is a function of the applied voltage. This varactor in series with the crystal provides the actual trim function. The fixed operating point for the varactor is supplied through the 100K resistor. Variable bias for the diode is supplied by the DAC through the 470K resistor. Figure 11 shows that a 50 PPM frequency trim range is achievable with the 12-bit DAC used.

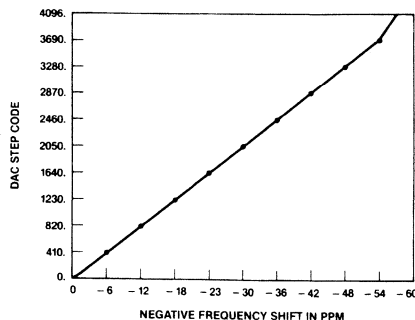


Figure 11) Tuning range of the tuneable crystal oscillator of Figure 10.

The frequency shift is down so it is recommended to specify the crystal approximately 25 PPM higher than the desired frequency. Initial trimming and re-trimming is easily accomplished by changing the DAC address settings as stored in the NOVRAM memory.

## Software Programmable Voltage Reference

Many systems (such as DVMs, test equipment, data acquisition systems and most forms of measurement and control apparatus) require a voltage reference that places a limit on total system performance. Figure 12 shows how a NOVRAM memory/DAC combination can provide a means of adjusting the output of a precision 10 volt reference.

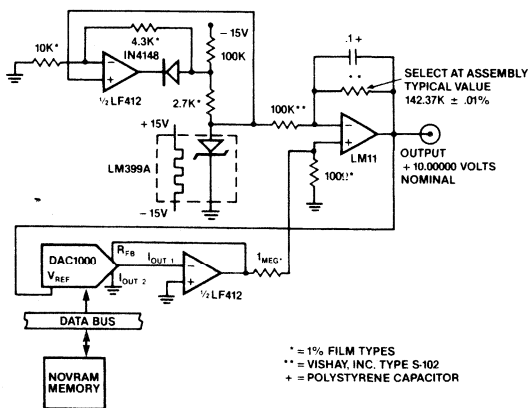


Figure 12) Software programmable voltage reference.

\* = 1% FILM TYPES  
 \*\* = VISHAY, INC. TYPE S-102  
 + = POLYSTYRENE CAPACITOR



An LM399A 6.95 volt reference is used in a bootstrap configuration to supply bias to the LF412 amplifier which in turn drives the LM399A. The 100K resistor insures start-up. The reference supplies bias to the LM11 amplifier, which supplies the circuit's output.

The NOVRAM memory/DAC-1000 combination supplies an offset voltage for the LM11 of 1 millivolt full scale in 1 microvolt increments. The 0.1  $\mu\text{F}$  capacitor insures dynamic stability and low noise at the LM11 output. To calibrate the output to within 1 microvolt, one sets the DAC to half scale and selects the feedback resistor of the LM11 until the output is within a few hundred microvolts of the desired value. Then the RAM portion of the NOVRAM memory is exercised, providing new inputs for the DAC until the desired value is achieved. This setting is then stored in the EEPROM portion of the NOVRAM memory. If a wider trim range is desired, the 1 megohm resistor can be reduced, but this degrades the setpoint resolution appropriately.

## Self-Calibrating, Interchangeable Probe Thermometer

A standard industrial temperature sensor with high linearity and long term stability is obtained using platinum resistance temperature detectors (RTDs). The RTD is specified in terms of its resistance at 0° centigrade (as this is a function of the manufacturing process), while the gain slope is relatively constant from unit to unit. A constant gain amplifier with an offset to compensate for the changing impedance at 0° centigrade is shown in Figure 13.

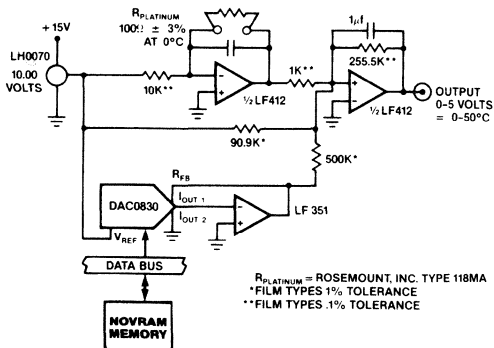


Figure 13) Self-calibrating, interchangeable probe thermometer.

The NOVRAM memory/DAC combination is used to modify the offset voltage of the amplifier to allow full interchangeability of probes in the field.

The platinum RTD shown has a  $\pm 3\%$  tolerance at 0°C ( $\pm 7.5^\circ\text{C}$ ) and is driven with a 1 milliampere constant current source by placing it in the feedback loop of the LF412 amplifier. The constant current is provided by the 10 volt reference IC. The amplifier output will be a linear function of the sensed temperature at the RTD. The 1  $\mu\text{F}$  capacitor limits noise pick-up and also insures that the RTD, a wirewound device with parasitic inductance, does not cause amplifier oscillations. The second half of the LF412 provides a fixed gain to the signal.

The 90.9K resistor provides a current to the summing junction of the amplifier to move beyond the correction for the worst case sensor. The NOVRAM memory/DAC pair then pull enough current from the summing junction to correct for the inserted RTD. Over a 0°C to 55°C range, this circuit is accurate to within  $\pm 0.25^\circ\text{C}$  while allowing the use of probes with a  $\pm 7.5^\circ\text{C}$  tolerance specification.

## Automatic Scale Calibration

The scale normally does not worry about a zero-level reading from its sensor, since it may have a wide variety of items on the platform such as wrapping paper or containers. An algorithm is usually required to automatically zero the scale before loading the material into the container. The transducer used in scale applications has a large variation in gain slope which must be corrected before shipping the scale or when changing the load cell. Figure 14 shows a circuit for providing these necessary corrections for the gain slope of the sensor.

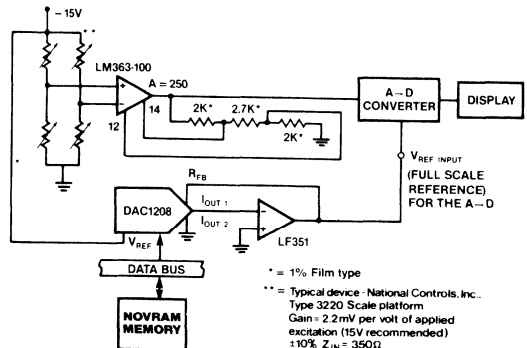


Figure 14) Automatic scale calibration.

The transducer shown, combined with the fixed gain amplifier, can produce outputs of 7.424 volts to 9.075 volts for full load depending on the transducer selected. To bring this result to the required value, the NOVRAM memory/DAC combination is used to vary the reference of an analog-to-digital converter. Since the DAC and the platform bridge are driven from the same supply, the measurement is ratiometric and no stable voltages are necessary. As the  $-15$  volt supply changes, the readout on the display will not vary. To calibrate a new platform, the scale is first zeroed out using the internal algorithm and then a fixed known weight is added to the platform. Then the NOVRAM memory/DAC unit is exercised until the correct readout is obtained. This calibration can be called from the scale's keyboard. Security for this adjustment can be in a software access code which is also stored in the NOVRAM memory.

## Gain Trimming For Photomultiplier Tube

The last example handles gain variations in a slightly different manner. The gain of a photomultiplier tube varies over time, temperature and power supply for a given input level. The output is a current from a high impedance source. A circuit to trim the changing gain is shown in Figure 15.

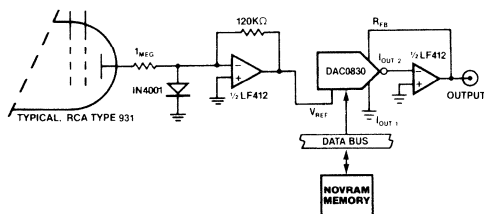


Figure 15) Gain trimming for photomultiplier tubes.

This current is converted to a voltage by the amplifier on the left side of the figure. For a full scale current of  $100 \mu\text{A}$ , the output voltage of this amplifier is 12 volts. This voltage output is used as the reference input for a NOVRAM memory/8-bit DAC combination which amplifies the reference from  $1/256$  through 1 depending on DAC setting. This gain can be varied in steps of  $1/256$ . The currents out of the photomultiplier tube are normally accurate to only 1% once the calibration is complete. Some applications, however, may require smaller steps in resolution. If this is the case, one could use a 10-bit DAC. Another method of obtaining

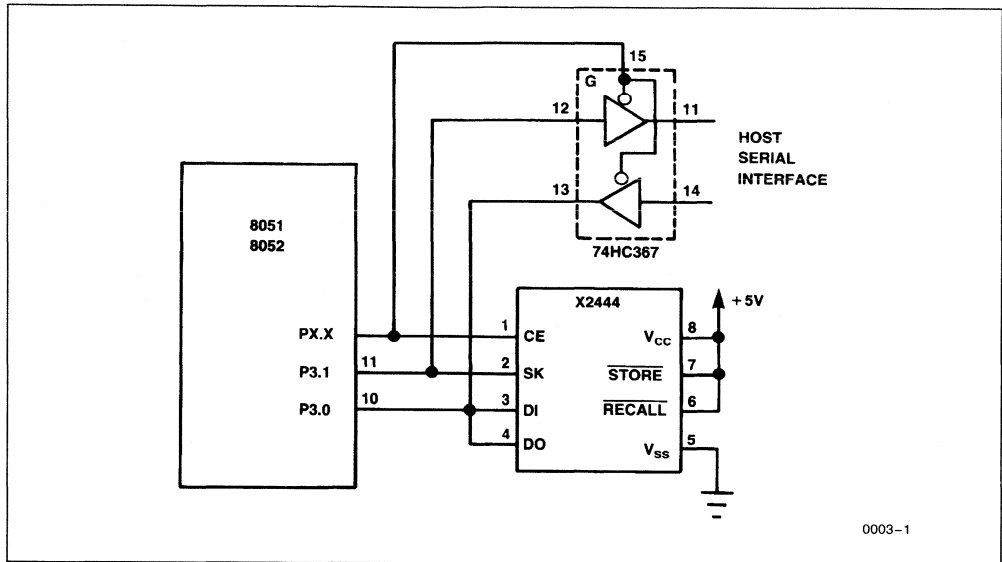
fine resolution is to use an 8-bit DAC connected as shown in Figure 8 in place of the DAC arrangement of Figure 15. If the feedback resistor of the left-hand amplifier is changed to 50K, very fine tuning (around a voltage gain of 2) is possible. This gain of 2 is established when the DAC is set for midrange of the digital value which gives a fine tuning range.

## Conclusion

This application note has shown how the NOVRAM memory can be used to replace commonly used mechanical components such as trimmers and DIP switches. This replacement improves reliability and reduces service costs for recalibration and resetting. In addition, actual equipment costs can be reduced.

Once a single NOVRAM memory is in the system, it is easy to include additional features in the unused portions. For example, a system designer could use a NOVRAM memory to replace DIP switches used for configuration data and then place calibration data for DACs in the unused memory. If even more unused space exists, storage of other desired data such as ID numbers or a service log would be possible.

The possible uses of NOVRAM memories are limitless. The designer is encouraged to build upon the ideas presented by this application note.



# THE X2444 SERIAL NOVRAM\* TEAMS UP WITH THE 8051 MICROCONTROLLER FAMILY

Add scratch pad RAM and nonvolatile parameter store via the 8051 serial port and still maintain full use of the serial port as a UART.

**Application from Rick Orlando  
Written by Richard Palm**

7

\*NOVRAM is Xicor's nonvolatile static RAM device.

## INTRODUCTION

The X2444 is a 256 bit serial NOVRAM internally configured as sixteen 16-bit words of RAM overlaid bit for bit with a nonvolatile E<sup>2</sup>PROM. The X2444 has the standard hardware RECALL and STORE inputs plus the ability to perform these same operations under software control, thereby freeing two microcontroller port pins for other tasks. The serial interface allows the X2444 to be packaged in a low cost space saving 8-pin mini DIP.

When teamed with the 8051 family of microcontrollers, the X2444's small physical size, software instruction set and serial interface make it an ideal parameter store and scratch pad memory while maintaining full use of the 8051 serial port as a UART.

## SCOPE

This application note describes interfacing the X2444 with the 8051 family of microcontrollers. Emphasis will be placed on the timing considerations of the interface, and explaining the modifications to the instruction words for normal device operation. This note assumes the reader has access to a Xicor Data Book and Intel *Microcontroller Handbook*.

## SERIAL PORT OPERATION

Port 3 on the 8051 provides a serial port that can be used in two basic configurations, full duplex and half duplex. This note examines the half duplex (mode 0) operation in interfacing to the X2444. Port 3 pin 1 (P3.1) is the clock output for both transmit and receive modes and Port 3 pin 0 (P3.0) is used for bidirectional data transfers.

The clock output frequency is  $\frac{1}{12}$  of the XTAL oscillator input frequency. To simplify timing calculations this note will assume an input frequency of 12 MHz resulting in a symmetrical 1 MHz output on P3.1.

The P3.1 and P3.0 pins when inactive (neither transmitting nor receiving) are always a logic 1 (HIGH). When a data transfer commences P3.1 will be LOW during machine cycle states S3, S4 and S5 and will be HIGH during states S6, S1 and S2. When transmitting, data is shifted out on P3.0 during S6P2 (state 6 phase 2) LSB first. When receiving, data is sampled during S5P2. Refer to Figure 1 for the basic 8051 serial port timing.

8051 / 2444  
PIN / PIN

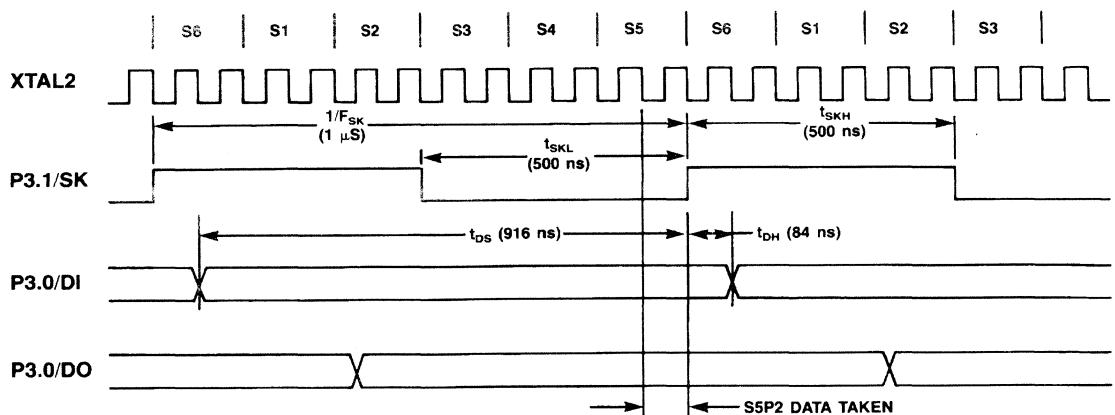


Figure 1. 12 MHz 8051 Serial Port Mode 0 and X2444 Timing

0003-2

# HARDWARE CONNECTIONS

The X2444 directly interfaces with the 8051 with no external circuitry required. DI and DO of the X2444 are both tied to P3.0, SK is tied to P3.1, CE is tied to any free port pin configured as an output and STORE and RECALL are tied to V<sub>CC</sub> (see Figure 2).

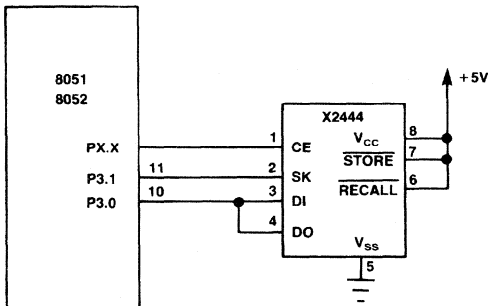


Figure 2. Basic Configuration

# X2444 OPERATIONS REVIEW

The X2444 is a serial device and in this application all chip functions are handled via the software instructions. The 8051 transmits data LSB first but the instruction format for the X2444 shows the instruction to be transmitted MSB first. This requires a simple transposition of the instruction, MSB for LSB. The memory is effectively a FIFO, so the data to be stored need not be transposed.

Internally the X2444 increments a bit (clock) counter. This is used to indicate the end of an instruction and if a read or write instruction is received, to increment a bit position pointer. This pointer enables individual RAM cells for writing and reading. The counter for the pointer increments from zero to fifteen. If CE remains HIGH and SK continues to clock, the counter will rollover from fifteen to zero. The word address does not increment; therefore, during a write operation if SK continues to clock and CE is HIGH, a 25<sup>th</sup> rising clock edge (8 edges for instruction + 16 edges for the data word + 1) would cause bit position zero to be overwritten.

# SYSTEM CHARACTERISTICS

Under normal operating conditions the X2444 expects CE to transition LOW to HIGH when SK is LOW in order that the first bit of data can be clocked into the X2444 on the first rising edge of SK. The data is sampled to see if it is "0" (a don't care state) or a "1" which is recognized as an instruction start. The 8051, however, places both P3.1 and P3.0 in the HIGH state when not actively transmitting. **THIS IS OK.** The X2444 internally gates CE and SK; therefore, toggling the port pin controlling CE to a HIGH effectively generates the first rising edge of SK, and also clocks in the HIGH present at P3.0 (DI).

What this does is clock a "1" into the X2444 indicating the start of an instruction prior to any shifting operation by the 8051 serial port. This will require dropping the leading "1" from the instruction. See Table 1 for the WAS/IS conditions for the equivalent instructions to be used by the 8051.

INSTRUCTION	WAS								IS							
	7	6	5	4	3	2	1	0	7	6	5	4	3	2	1	0
WRDS	1	X	X	X	X	0	0	0	X	0	0	0	X	X	X	X
STO	1	X	X	X	X	0	0	1	X	1	0	0	X	X	X	X
SLEEP	1	X	X	X	X	0	1	0	X	0	1	0	X	X	X	X
WRITE	1	A	A	A	A	0	1	1	X	1	1	0	A	A	A	A
WREN	1	X	X	X	X	1	0	0	X	0	0	1	X	X	X	X
RCL	1	X	X	X	X	1	0	1	X	1	0	1	X	X	X	X
READ*	1	A	A	A	A	1	1	X	1	X	1	1	A	A	A	A

\*Note: bit 7 of the READ command should be a "1" to avoid bus contention.

Table 1. Reconfigured Instruction Format

The 8051 will still generate eight rising clock edges on P3.1 for each byte loaded into the shift register (SBUF), effectively providing the X2444 with nine clocks for the first byte. For the single byte instructions the ninth clock and data are ignored by the X2444. Refer to Figure 3 for the single byte instruction timing.



8051/52 / 2444  
PIN / PIN

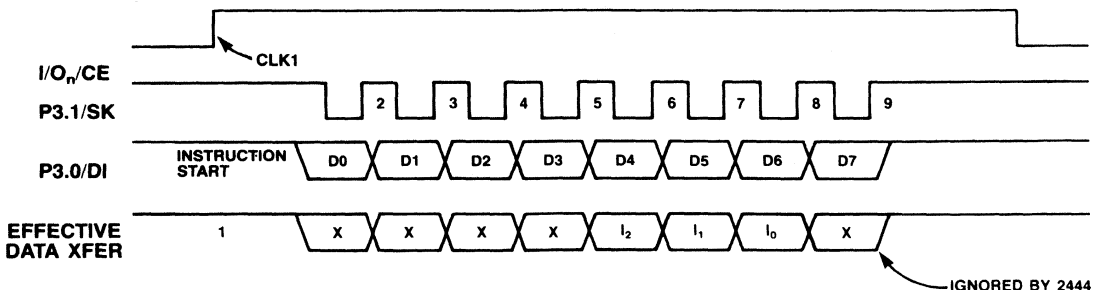


Figure 3. Single Byte Instructions

## WRITING

Writing to the RAM array is straightforward. The write instruction is issued by the 8051 in the same manner as the single byte instructions. The MSB (eighth bit) of the instruction byte is clocked in on the equivalent ninth clock rising edge. This bit is recognized as the first data bit transfer and is initially written into the addressed word's bit position zero. The 8051 will continue to transmit two more bytes of actual data. The LSB (bit "0") of the first byte will be physically located in bit position "1" and all subsequent bits will also be offset by one. The MSB (sixteenth data bit) of the word will be written into bit position zero, overwriting the last bit of the instruction byte. Refer to Figure 4 for the sequence of operations.

## READING

Reading data back from the RAM array is quite similar. The X2444 begins to shift data out during the instruction cycle (more on this later). After the instruction is shifted out, the 8051 must turn around P3.0 and configure it as an input. CE and SK are static during this period and the DO output will remain unchanged until after the rising edge of the first 8051 receive data clock. Therefore, the first data shifted into the 8051 will be from bit position "1", equivalent to the LSB originally written. Refer to Figure 5 for the sequence of operations.

8051 / 2444  
PIN / PIN

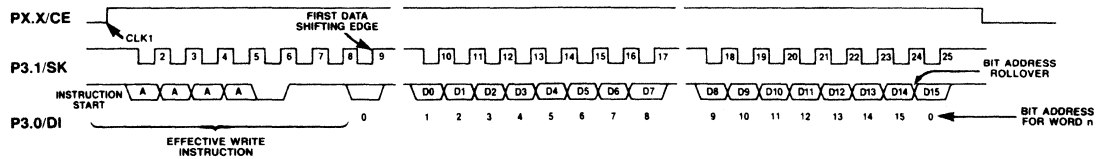


Figure 4. Write Cycle Sequence

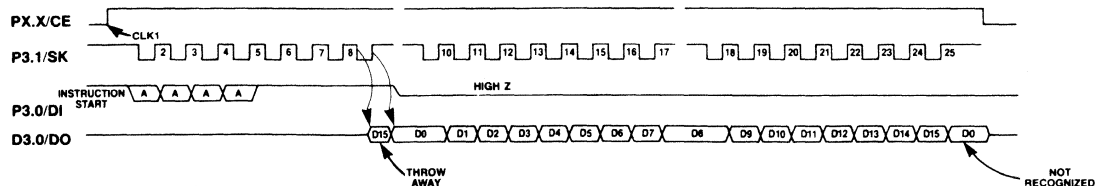


Figure 5. Read Cycle Sequence

## BUS CONTENTION

There will not be any bus contention for single byte instructions or the write command. However, for the Read command there could be contention. While the 8051 is still shifting out the instruction byte the X2444 begins to output data on the same line. Refer to Figure 5, just after the falling edge of clock eight.

The 8051 shifts out data at S6P2. If the data changes state from "0" to "1" a high current enhancement FET is turned on for two 8051 system clock cycles. This is used to provide a fast rise time. At the end of this two cycle period, the enhancement FET is turned off and the output is held HIGH by a depletion mode FET that essentially looks like a resistor pullup (Refer to Intel's *Microcontroller Handbook* [1984] pages 6-6 and 6-7). Note that the high drive circuit is enabled only for data state changes from "0" to "1"; therefore, if the output is already a "1" and another "1" is shifted out on P3.0, the high drive will *not* be turned on. This depletion FET can source a maximum of 250 $\mu$ A if the port pin is grounded.

The instruction table indicates that bit seven for the READ instruction should be a "1". The reason for this is to guarantee that the high drive period is off before the X2444 begins to output data. If bit seven were a "0", the 8051 would turn on the high drive circuit to return P3.0 to the inactive state, possibly generating a high current contention problem with the DO output of the X2444. Figure 6 illustrates the timing involved during clock eight. The high drive period of the 8051 is turned off well before the X2444 begins to output data.

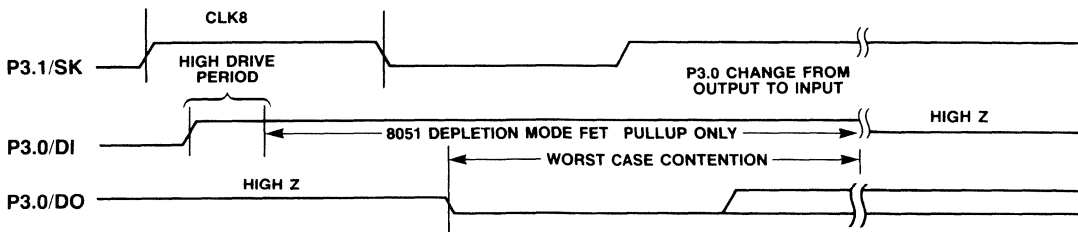


Figure 6. Worst Case Bus Contention

## VERSATILITY

The DO output of the X2444 is always in the high impedance state unless it is outputting data in response to a READ command. Therefore, the serial port of the 8051 need not be dedicated solely to a serial memory interface.

Figure 7 illustrates the versatility this affords. This figure depicts the basic system components required in a remote location controller. Notice that the 8051 serial port has access to both the X2444 and through the use of the CE control line maintains full use of the serial port as a UART. Therefore, it can receive downloaded parameters from a host, re-enable the serial port for X2444 communication, then store the data either temporarily in the X2444 RAM array or permanently in the X2444 E<sup>2</sup>PROM array.

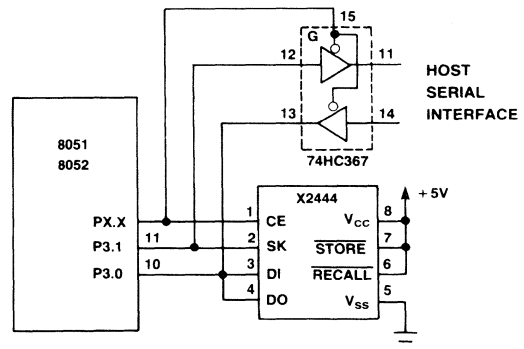


Figure 7. Shared Serial Port

---

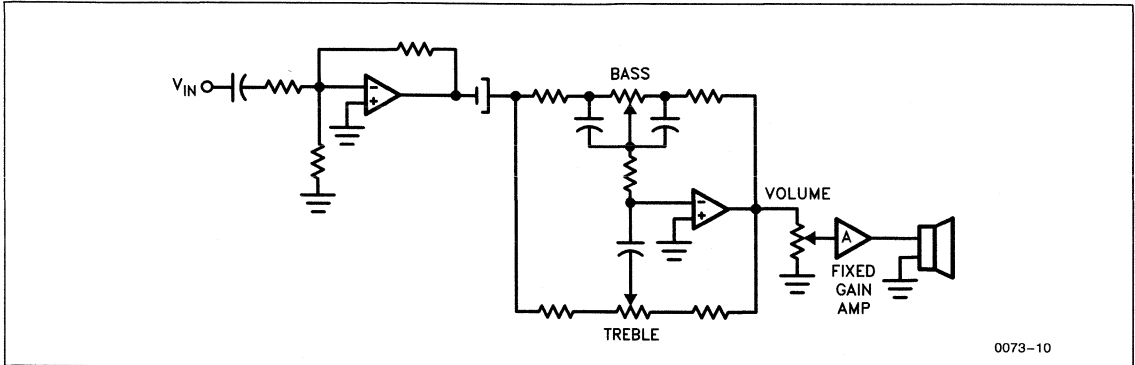
## CONCLUSION

This application note has shown that with no extra hardware the X2444 interfaces directly with the 8051 family of microcontrollers, providing a non-volatile memory store and scratch pad memory and

maintaining full 8051 UART capabilities. It is the ideal solution for applications where extra memory is required but few port pins are available for implementation.

0003-6





# E2POT™ DIGITALLY CONTROLLED POTENTIOMETER BRINGS MICROPROCESSOR CONTROL TO AUDIO SYSTEMS— ADDS FEATURES

By Jeff Randall

7

## INTRODUCTION

Control of most audio circuits is still accomplished the same way it has been for the last fifty years or so. From the volume control knob to the sliders on an equalizer, the control is human, the feedback is through the ears, and the control element is the mechanical potentiometer. Microprocessors have entered nearly every other segment of electronics, and as they enter the audio segment, they slam headlong into the mechanical potentiometer.

While this article focuses on microprocessor control of conventional audio circuits through the use of digitally controlled potentiometers, it should become clear how these devices can be applied to many other applications as well.

## CONVENTIONAL AUDIO CONTROL

A look at conventional methods for audio control should help to illustrate the situation:

Designs incorporating mechanical potentiometers are still found in the majority of audio applications. For example, the volume control on most car stereos is a rotary potentiometer. Volume control circuits generally resemble Figure 1. In this design, the potentiometer is used to control the signal reaching a fixed gain amplifier section. A potentiometer in this application would likely have a logarithmic taper, since volume is a logarithmic function.

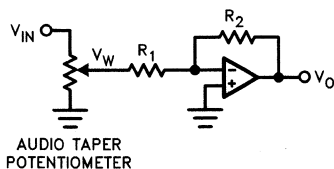


Figure 1: Conventional Potentiometer Volume Control

0073-1

Tone controls can vary from single pot and capacitor circuits to complex active filters. The Baxandall filter network has been the workhorse of the audio industry for years. This design, illustrated in

Figure 2, utilizes two linear taper potentiometers to control the gain of an active filter. In this configuration, the potentiometer replaces a portion of both the input and feedback resistors. By moving the position of the wiper, both resistors change in opposite directions.

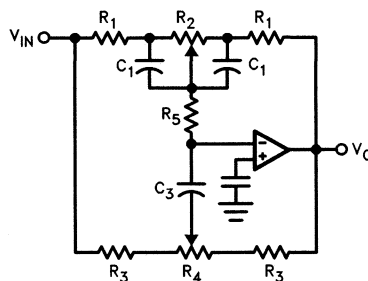


Figure 2: Baxandall Tone Control Circuit

0073-2

Graphic equalizers are one of the fastest growing modes of audio control. A graphic equalizer contains a group of band pass filters, usually seven. Each filter has a potentiometer controlling the gain to that band pass. Potentiometers generally appear as sliders on the face of the equalizer.

A typical graphic equalizer schematic is shown in Figure 3. EQs are used to compensate for the imperfections of a listening environment by boosting or cutting gain at specific frequencies. By using a spectrum analyzer and a "pink" noise generator, the response of an audio system can be customized for a particular room or concert hall. This is accomplished by inputting a desired response to the system—generally flat across the audio band, with some attenuation at higher frequencies, often referred to as "pink" noise. The equalizer is then adjusted until the system output, displayed on the spectrum analyzer, closely matches the pink noise input.

This process of matching a system to a room is often referred to as environmental calibration. It is a process requiring the listener to read the display of the spectrum analyzer and manually adjust the potentiometer/sliders of the equalizer.

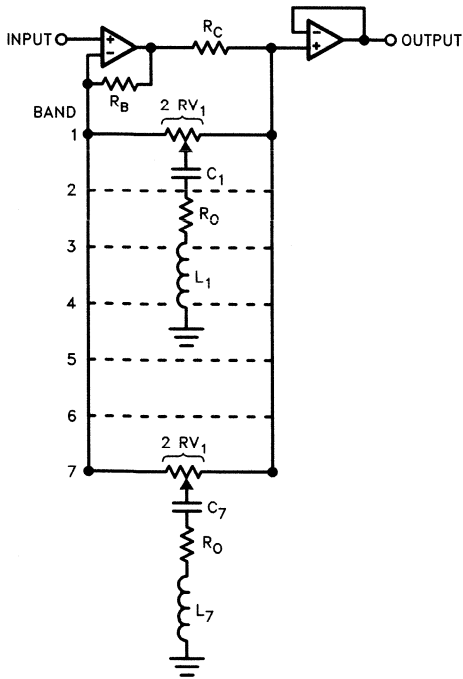


Figure 3: Graphic Equalizer Configuration

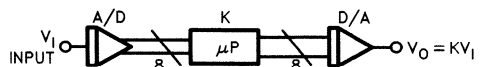
0073-3

The heart of the control of each of the circuits described earlier is the mechanical potentiometer. Automated control of these devices is a challenge. Clearly, microprocessor control of these functions is desirable. The control elements utilized for automated control are discussed below.

## AUTOMATED CONTROL ELEMENTS

While these devices are primarily used for industrial control applications, motorized potentiometers offer a relatively straightforward approach to simple audio control circuits. In these devices, a DC reference voltage, or a digital signal representing position is input to a small motor assembly that is linked to a rotary potentiometer. Drawbacks to this type of system are numerous, including noise caused by the motor assembly as well as the increased space and power requirements of placing a motor on an audio PC board.

D/A converters can also be used to control and manipulate analog circuit functions, but introduce more complexity. These devices are the choice of high fidelity digital audio controls due to their high precision. But for the analog circuit designer, they can be a little intimidating. For example, one way to control volume with D/A converters is illustrated in Figure 4. In this circuit, the signal is sampled with a A/D converter, manipulated by a microprocessor, and returned to the analog world with a D/A converter. This design entails sampling, real-time processing, as well as A/D and D/A conversions. Not only may the analog designer be faced with portions of his circuit that may be unfamiliar, the results may be overkill.



0073-4

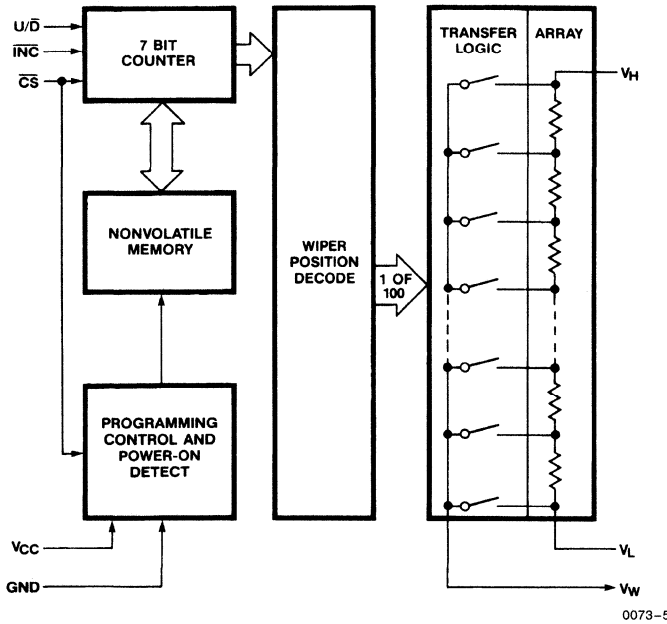
Figure 4: Volume Control Using D/A Conversion

An array of resistors with a wiper tap that can be selected with digital control offers many advantages of the microprocessor world without the complexity of D/A conversion. These are referred to as digitally controlled potentiometers. Logic circuits, counters, and memory circuits are often teamed up with resistor arrays to accomplish an approximation of potentiometer control. Recently, a few manufacturers have introduced devices which incorporate many of these functions in one device. Examples are Xicor's X9MME, Toshiba's TO9169AP, and National's LMC835.

The Toshiba and National parts are designed around specific audio applications and are distinctively different from the Xicor device. They incorporate features that lend well to audio designs, but are not intended for general purpose potentiometer replacement. Moreover, they offer only a limited number of wiper positions.

Xicor's X9MME combines a single 99 position potentiometer with three line digital controls. Figure 5 contains a functional diagram, pin description and mode selection for the device. In addition to the internal counter circuitry for wiper position control, this part also incorporates nonvolatile memory to retain wiper position. It has been designed as a digitally controlled replacement for the mechanical potentiometer. With its conventional three terminal potentiometer design, it integrates easily into existing analog designs.

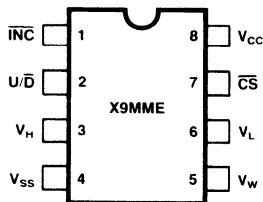
## Functional Diagram



## Mode Selection

$\overline{CS}$	$\overline{INC}$	$U/\overline{D}$	Mode
L		H	Wiper Up
L		L	Wiper Down
	H	X	Store Wiper Position

## Pin Configuration



## Pin Names

$V_H$	High Terminal of Pot
$V_W$	Wiper Terminal of Pot
$V_L$	Low Terminal of Pot
$V_{SS}$	Ground
$V_{CC}$	System Power
$U/\overline{D}$	Up/Down Control
$\overline{INC}$	Wiper Movement Control
$\overline{CS}$	Chip Select for Wiper Movement/Storage

Figure 5: The X9MME Digitally Controlled Potentiometer

To illustrate digital control of potentiometer circuits, the X9MME from Xicor was used to replace mechanical potentiometers in a well known audio circuit. The following should demonstrate the ease of designing with the X9MME as well as the advantages of microprocessor control in audio circuits.

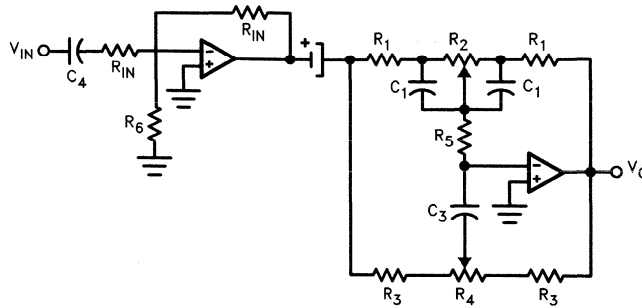
## THE X9MME IN AN AUDIO CIRCUIT

The Baxandall tone control circuit is the basis for the designs shown here. The following sections will discuss the principles behind the Baxandall circuit

and then walk through the design utilizing the X9MME. Special design considerations for the X9MME will be discussed, and the performance and operation will be evaluated.

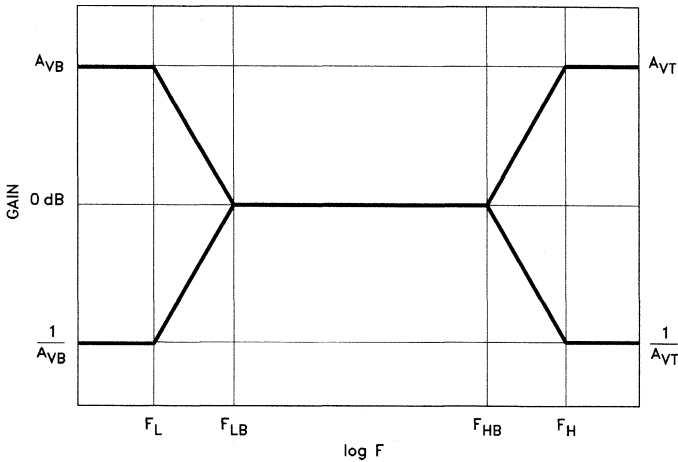
The Baxandall circuit, its response, and equations for gains and filter frequencies are shown in Figure 6. This circuit contains two active filters whose gain is controlled by two potentiometers. Figure 7 illustrates the bass portion of the circuit. The maximum gain of this circuit is at low frequencies, where the capacitors in the circuit can be considered to be open circuits. The capacitors have been omitted for clarity. (The treble portion of the circuit, not illustrated here, follows along similar lines.)

## Schematic



0073-7

## System Frequency Response



$$F_L = \frac{1}{2\pi R_2 C_1} \quad F_H = \frac{1}{2\pi R_3 C_3}$$

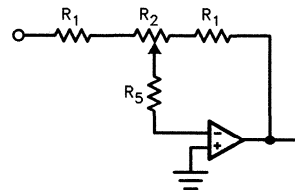
$$F_{LB} = \frac{1}{2\pi R_1 C_1} \quad F_{HB} = \frac{1}{2\pi (R_1 + R_3 + 2R_5) C_3}$$

$$A_{VB} = 1 + \frac{R_2}{R_1} \quad A_{VT} = 1 + \frac{2R_5 + R_1}{R_3}$$

0073-8

Figure 6: Active Audio Preamplifier

With the addition of another potentiometer on the output of the Baxandall network, the system represents a single channel of an audio preamplifier. The circuit contains three potentiometers which control volume, treble and bass. These pots would appear as knobs on the face of a home or car stereo, to be adjusted by hand to control and shape the sound reaching the amplifier and speakers.



0073-9

$$|A_{VB}| = \frac{R_1 + R_2}{R_1} \quad \text{Maximum Bass Boost}$$

Figure 7: Bass Portion of Active Preamp Circuit

7

Neglecting the digital control lines and 5V power for the X9MME, the circuit is shown in Figure 8. The X9MME will replace bass, treble and volume potentiometers. Note that this does not alter analog design considerations.

It should be noted that  $R_2$  and  $R_4$  are both linear taper pots. Since the X9MME is also a linear taper pot, it is a direct replacement.  $R_V$ , the volume potentiometer, is specified as an audio taper pot, since it is used for volume control. By placing a small resistor from wiper to low on any linear pot, as shown in Figure 9, an audio taper can be approximated. In this case a resistor of one-tenth the total pot resistance is a close approximation of an audio pot (EDN Nov. 13, 1986).

This circuit is designed to have a gain of one across the entire audio range, with the potential for a boost or cut of 20 dB at the frequencies selected by the designer.

## THE DESIGN

The design chosen is intended for car stereo applications. It should therefore operate from a single ended, 12V supply and adapt well to speakers that

are commonly used in automobiles. Considering the limited bass response of most car speakers, the bass boost or cut should not be so low that the speakers cannot reproduce the sound.

The desired circuit would operate from a 12V power supply, have a  $\pm 20$  dB boost or cut at 100 Hz (bass) and 10 KHz (treble). The available resistor values for the X9MME are 10K, 50K, and 100K. The following steps outline the design:

1.  $R_2 = 50 \text{ K}\Omega$  (arbitrary, X9503)

The design must start somewhere. This value was actually determined after running through the design a couple of times and comparing the values determined for the potentiometers with those available.

2.  $A_{VB} = 1 + R_1/R_2$ ; for 20 dB (10),

$$R_1 = R_2/9 = 5.6 \text{ K}\Omega$$

The bass portion of the circuit must have a maximum boost of 20 dB. This is determined with the bass pot all the way to the input side. A quick look at Figure 8 will illustrate this.

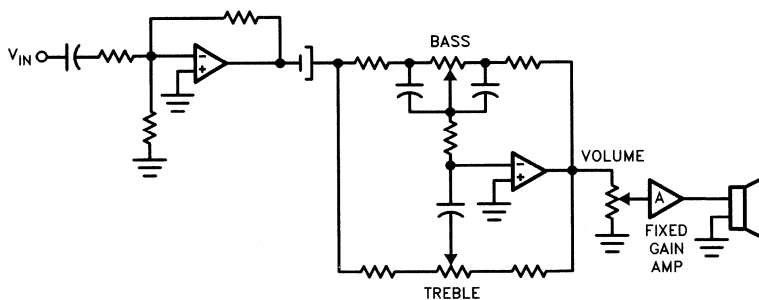
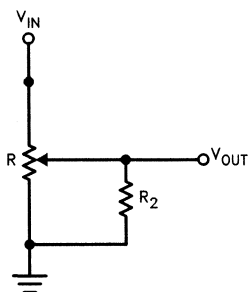


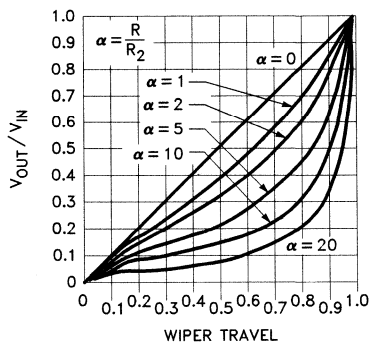
Figure 8: Active Preamp with Bass, Treble and Volume Controls

0073-10



For Audio Taper, Use  $R_2 = \frac{R}{10}$ .

0073-11



0073-12

Figure 9: Utilizing External Resistors to Vary Potentiometers Trim (EDN Nov. 13)

$$3. F_L = 100 \text{ Hz}, F_{LB} = 1 \text{ KHz}$$

$$C_1 = \frac{1}{2\pi F_{LB} R_1} = \frac{1}{2\pi(1000)(5.6K)}$$

$$= 2.84 \times 10^{-8} \text{ F}$$

Here, the formulas for the cutoff frequencies of the active filters are broken down to determine the element values to use.

$$4. R_5 = 2.2 \text{ K}\Omega \text{ (arbitrary)}$$

$$5. A_{VT} = 1 + \frac{R_1 + 2R_5}{R_3} = 10,$$

$$R_3 = \frac{R_1 + 2R_5}{9} = 1.1K$$

Use 1 K $\Omega$

Here, the maximum treble gain is calculated in similar fashion to the maximum bass gain.

$$6. C_3 = \frac{1}{2\pi F_H R_3} = \frac{1}{2\pi(10K)(1K)} = 1.6 \times 10^{-8}$$

$$7. R_4 \geq 10 (R_3 + R_1 + 2R_5) = 110 \text{ K}\Omega$$

Use 100 K $\Omega$

$$8. R_V = 10 \text{ K}\Omega \text{ (arbitrary)}$$

The circuit with the X9MME inserted is shown in Figure 10. These are the values that were used in lab experiments and for demonstration purposes.

It should be noted that some considerations in the design had to be altered when the X9MME was inserted into the circuit. The X9MME is a source of high frequency noise. There are internal voltage generators on the device which are used to operate switches internally as well as to store information into the device's nonvolatile memory. The principle noise frequencies begin at approximately 150 KHz, and while this is beyond the audio range, it can still be a source of problems in the circuit. For this reason, capacitors were added around the X9MME to filter noise. These are included in Figure 10.

## DIGITAL CONTROL

The digital control lines of the X9MME are  $\overline{INC}$ ,  $\overline{CS}$ , and  $U/\overline{D}$ .  $\overline{CS}$  (chip select) allows the wiper to be moved.  $U/\overline{D}$  (Up/Down) determines the direction in which the wiper will move, and  $\overline{INC}$  (increment) initiates movement on its falling edge.  $\overline{CS}$  is also used to store the wiper position in nonvolatile memory. When  $\overline{CS}$  is returned high, a store operation is commenced.

When initially designing with the part, it was helpful to assemble a simple switch system for controlling the parts. A 555 timer was used to generate a fairly slow clock pulse and connected through a momentary switch to the increment pin of each X9MME. With pull up resistors on each digital line, a grounding switch was connected to  $U/\overline{D}$  and another to  $\overline{CS}$ . To move the wiper up,  $\overline{CS}$  was set to

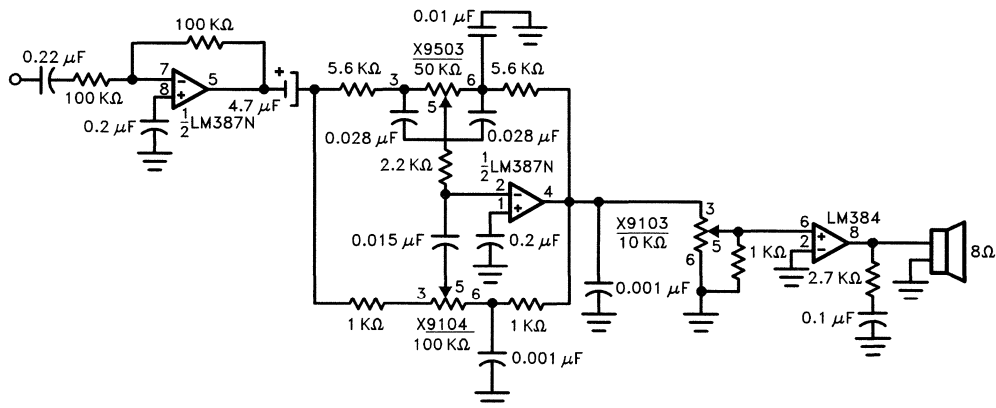


Figure 10: E2PREAMP with Three X9MME—No Digital Controls Shown

0073-13

ground,  $U/\overline{D}$  to 5V and  $\overline{INC}$  pulsed with the clock. Each step of the clock produced a 1% change in wiper position. Figure 11 illustrates the switching network that was utilized for controlling all three X9MMEs.

This initial procedure allowed the analog portion of the design to be separated from the digital. Once the circuit was functioning adequately with the switch network controlling the X9MMEs, microprocessor interface was relatively simple.

## MICROPROCESSOR INTERFACE

With three devices on the board, 9 control lines are required. To simplify interface to an 8 bit microprocessor, the  $\overline{INC}$  lines for all three parts were connected to the same pin.

The pin configuration used for interface to the 6502 microprocessor system is as follows:

A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
NC	$\overline{INC}$	$\overline{CS}_1$	$U/\overline{D}_1$	$\overline{CS}_2$	$U/\overline{D}_2$	$\overline{CS}_3$	$U/\overline{D}_3$
#1 = Volume							
#2 = Bass							
#3 = Treble							

To move the wiper of a given pot, that pot's  $\overline{CS}$  is brought low, the  $U/\overline{D}$  for the appropriate pot is asserted H or L depending on the direction of wiper movement, and  $\overline{INC}$  is toggled. For example, to increase the volume the following two patterns are alternated to the port connected to the E<sup>2</sup>PREAMP.

NC	$\overline{INC}$	$\overline{CS}_1$	$U/\overline{D}_1$	$\overline{CS}_2$	$U/\overline{D}_2$	$\overline{CS}_3$	$U/\overline{D}_3$
1	0	0	1	1	1	1	1
1	1	0	1	1	1	1	1

Note that  $\overline{CS}$  has been selected,  $U/\overline{D}$  set to 1 and  $\overline{INC}$  toggled. Bass and treble settings are altered in a similar manner.

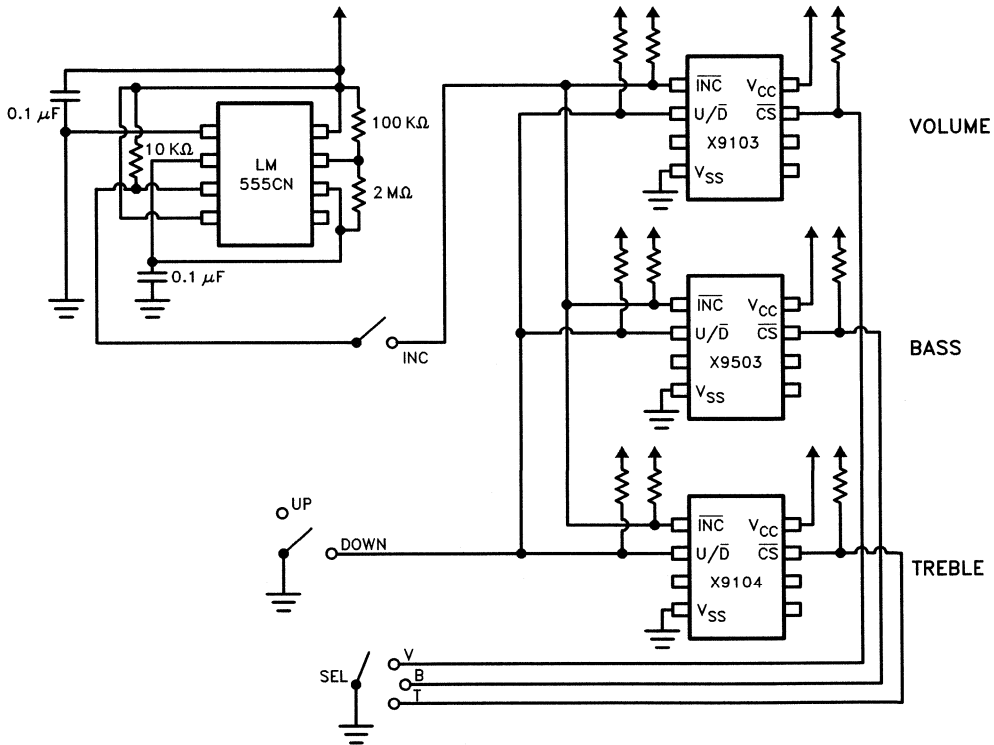


Figure 11: Switch Network for Manual Operation



The microprocessor system used in the lab consists of a 6502 based keyboard monitor. The controlling program scans the keyboard for a recognized ASCII character which transfers control to the specified subroutine. For any given input, the appropriate increment is toggled 10 times before returning to the controlling program.

An example of a volume, bass, or treble adjusting program follows:

```

LDX #00          Load counter with zero
0333 LDA 0006     Load accumulator with first
                  pattern
      STA A000    Output pattern
      JSR ED2C   5 ms wait
      LDA 0007   Load 2nd pattern
      STA A000
      JSR ED2C
      INX
      CPX 0008   Compare counter to 10
      BNE 0333
      RTS

```

In addition to the adjustment subroutines, an initialization subroutine can also be called up. This subroutine sets the volume to zero and bass and treble to 50%. This is used to reset the controls. It would be used only during installation of the system.

This first section of the one time initialization program sets all pots to zero.

```

LDX #00          Load counter with zero
0111 LDA 0000     Load accumulator with first
                  pattern (80h)
      STA A000    Output pattern
      JSR ED2C   5 ms wait
      LDA 0001   Load 2nd pattern (C0h)
      STA A000
      JSR ED2C
      INX
      CPX 0008   Compare counter to 100
      BNE 0111

```

This section sets the bass and treble pots to 50% and returns control to the controlling routine.

```

LDX #00          Load counter with zero
012C LDA 0003     Load accumulator with first
                  pattern (85h)
      STA A000    Output pattern
      JSR ED2C   5 ms wait
      LDA 0004   Load 2nd pattern (F5h)
      STA A000
      JSR ED2C
      INX
      CPX 0005   Compare counter to 50
      BNE 0333
      RTS

```

## OPERATION AND PERFORMANCE

The E<sup>2</sup>PREAMP circuit operates much like many sophisticated home stereo systems today. All controls are digital switches—in this case, a keyboard for demonstration purposes only. There are no moving parts beyond the switches, and the entire system is relatively free from problems with vibration or jarring (potential hazards in mechanical pot systems).

Keys 1 through 6 on the keyboard represent the up down controls for the circuit. By depressing 1, the volume is increased by 10 steps. Key 2 decreases volume in the same way; 3 is treble up; 4 is treble down; 5 is bass up; 6 is bass down. The I key calls the initialization routine. Beyond allowing control of step size and the auto zero or initialize function, the present system does not take advantage of the versatility of microprocessor control.

Performance of the system was nearly identical to the same circuit with mechanical potentiometers. The X9MME is quiet to -65 dB below a 1V signal, which is fair for audio quality devices. For audiophile quality, this number should be around -120 dB, but in car stereo or communication equipment applications this device works adequately.

Aside from the obvious advantage of a lack of moving parts, the ability to choose step size in adjusting the controls has shown to be the most useful added feature. Ten steps per adjustment proved to be an easy value with which to work.

Having demonstrated the ability of the X9MME to replace mechanical potentiometers in analog circuits, more complex circuits may now be considered. With microprocessor control, advanced circuit design and digital control simply becomes an extension of the principles discussed so far.

Microprocessor control of this and other analog circuits is simple when utilizing a digitally controllable potentiometer. The gain of the entire circuit, or the boost or cut of a given frequency range is instantly alterable via microprocessor commands. Once control is assumed by the microprocessor, any parameter of the analog circuit that is controllable by a potentiometer is available to the programmer.

For example, the graphic equalizer/spectrum analyzer combination discussed earlier can easily be automated once microprocessor control is assumed. By controlling the position of potentiometers that control the gain of the individual equalizer bands, the system frequency response can be calibrated to any room or listening environment. Here is

---

just one scenario: A "Calibration" button is depressed on the equalizing circuit. This activates a "pink" noise generator which sends a short burst of sound to the system. The spectrum analyzer in the system then decides which frequencies require adjustment, changes the positions on the appropriate potentiometers, and the system is calibrated. No sliders need to be adjusted; no separate (and expensive) spectrum analyzer; moreover, a relatively unsophisticated user can now perform an accurate environmental calibration of the system.

A simpler version of an auto calibration circuit could be incorporated into home and car stereos as a one time only installation adjustment. The scenario would be as follows. When a car stereo is first installed, the installer would push the calibration button on the back of the unit. This would adjust a compensation circuit, separate from the main tone controls. The settings would then remain in the non-volatile memory of the digital pots until the system were upgraded or installed into another car. Thus the same unit would be customized for different speakers, different amplifiers, and even different auto interiors.

## X9MME ADVANCED FEATURES

The Xicor device utilized in this design is suitable for audio applications, but it is a general purpose device that may be even better suited for other analog applications.

The X9MME has 99 steps across its range. In most audio applications, this high resolution is inaudible. However, when used in auto zero and balancing circuits, this resolution is invaluable.

The device's nonvolatile memory may be of limited use in some of the applications mentioned here, since a listener may not want to retain previous audio settings. But when used in a once-only calibration circuit, the nonvolatile memory eliminates any need for preventing a customer from changing the factory settings of a mechanical potentiometer. In a television cable decoder, for example, potentiometers abound. If cable companies used nonvolatile digital potentiometers in place of mechanical pots, the incessant headache of having to make adjustments because of jarred equipment or tampering could be eliminated.

The X9MME's convenient packaging and inherent digital control characteristics can be used to advantage on the assembly line. Manufacturing of devices requiring manual adjustment of potentiometers is always limited by the speed of the laborers and equipment used to set the pots. In addition, units often must remain partially assembled, or allow access holes for screwdriver adjustment of pots. The X9MME's conventional 8 pin DIP package can be automatically inserted with handlers used for other DIP devices, and trimmed to an appropriate value with an assembly line computer or by an internal microprocessor.

## CONCLUSION

Microprocessor control of analog circuits is now easier than ever. The X9MME from Xicor is more than a simple DAC. Not only can this device be used as a precision voltage source, it can replace any resistive element in nearly any analog circuit. Without altering existing analog circuit designs, the designer now has the ability to manipulate analog circuit functions with the digital potentiometer as his control element.

## REFERENCES

1. Giles, Martin, et al, *Audio/Radio Handbook*, Santa Clara, CA: National Semiconductor, 1980.
2. Gray, Paul R., Meyer, Robert G., *Analysis and Design of Analog Integrated Circuits*, Toronto, Canada: John Wiley and Sons, 1984; pp. 635-700.
3. Rumreich, Mark, "Resistors Provide Nonlinear Pot Tapers", EDN November 13, 1986, pp. 292, 293.
4. Stremmer, Ferrel G., *Introduction to Communication Systems*, Reading, MA: Addison-Wesley Publishing Co., 1982; pp. 93.
5. National Semiconductor Corp., "Product Data Sheet, LMC835", April, 1984.
6. Toshiba Corp., "Product Data Sheet, TC9169AP-TC9170AP" June 1985.

## THE NINE MOST FREQUENT NOVRAM\* QUESTIONS

By Rick Orlando

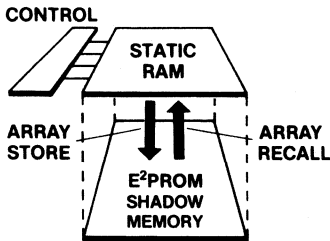


Figure 1: Xicor NOVRAM SRAM Functionality with Nonvolatile E<sup>2</sup>PROM

This provides a completely free bus, so that the processor can utilize the store cycle period performing other tasks. In order to maximize NOVRAM accessibility, the actual Store cycle completion can be detected by monitoring this high impedance condition. For example, if using a "pulled-up" bus, a specific RAM location can be repeatedly read until its non-FF contents are acquired. At that point, the system knows that the Store cycle is complete and the NOVRAM is accessible.

The NOVRAM (Nonvolatile RAM) from Xicor is being utilized in a multitude of systems and applications today. As engineers throughout the industry become aware of its availability, their appreciation for this state of the art technology, and the design flexibility which it affords them, is demonstrated by its rapidly expanding use. NOVRAMs have become the "secret" of many winning product designs by providing the technical edge which defines the industry leader.

Although the X2200 series NOVRAMs are very easy to use, the possibilities created by their simplicity and versatility bring forth questions regarding their more subtle characteristics. Frequently, the clarification of these points provides creative engineers with insights into new and unique applications.

**Question No. 1:** Will the RAM portion of the NOVRAM be accessible during the 10ms Store cycle?

**Answer:** No. From initiation of the Store cycle until its completion, the data outputs are in a high impedance state and the control inputs are inhibited.

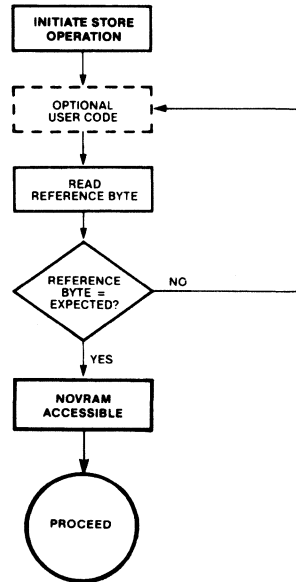


Figure 2: Early Write Completion Flowchart

\*NOVRAM is Xicor's nonvolatile static RAM device.

**Question No. 2:** Will the application of voltage to pins marked NC (Not Connected) damage the part?

**Answer:** No. The pins are literally not electrically connected to the die.

**Question No. 3:** Will the RAM be accessible for either reading or writing while the ARRAY RECALL pin is held low protecting the nonvolatile data?

**Answer:** No. While ARRAY RECALL is low, the data outputs are placed in a high impedance state and all control inputs are inhibited. This feature is particularly useful for preventing inadvertent Store operations during power transitions. Pulling ARRAY RECALL low in these periods prevents unintentional data changes.

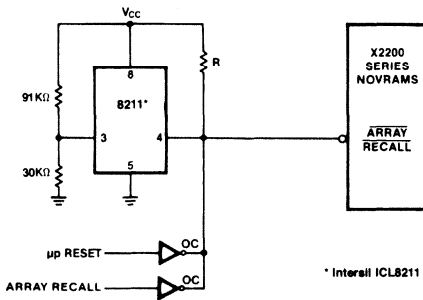


Figure 3: Power-up/Power-down Write Protection Circuit

**Question No. 4:** What happens if  $V_{CC}$  falls below 4.50V before the Store cycle is complete?

**Answer:** A complete and accurate Store operation is only guaranteed while  $V_{CC}$  is within spec (i.e., 5.0V + 10%). If the supply voltage drops out of that range during a Store operation, the result of the Store is not predictable. The Store operation typically completes in less than 5ms, and if it is completed before  $V_{CC}$  falls out of range, the data will be secure. However, the many internal system factors involved as the supply voltage diminishes make Storing without sufficient time a potential catastrophe. Always allow at least 10ms between the Store cycle initiation and  $V_{CC}$  dropping below 4.50V for certainty in your "data perfect" system crash designs.

**Question No. 5:** How does Store time vary with device temperature?

**Answer:** The duration of the Store cycle time is a function of the operating temperature. In general, higher temperatures cause a longer store cycle time, but, within specified limits, does not exceed 10ms.

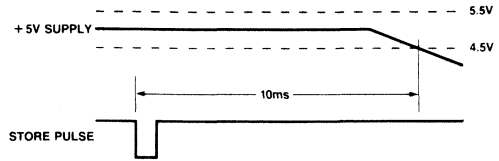
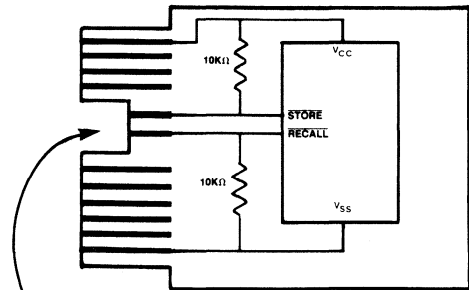


Figure 4: Initiate Store to Power-down Condition Timing

**Question No. 6:** We found the NOVRAM to be the perfect memory device for our plug-in cartridge application. Is any precaution necessary to protect the data while the cartridge is handled out of the system?

**Answer:** The best protection is simply to use a pull-down resistor in the cartridge tying ARRAY RECALL to the  $V_{SS}$  pin. This will prevent any unanticipated cartridge power (like decaying capacitors and external static voltages) from modifying NOVRAM data.

Although in a strictly 5V environment, "hot socket" insertion will not harm the NOVRAM, precautions should be taken to ensure that cartridge insertion and removal does not generate inadvertent Write or Store commands.



Note that these two are the last contacts made during insertion.

Figure 5: Typical Cartridge Write Protect Scheme

**Question No. 7:** Two distinct "endurance" parameters are specified on the NOVRAM data sheet. What is the difference between them, and how may this distinction be advantageously used?

**Answer:** The X2200 data sheets specify a minimum of 10,000 Store cycles and 1000 changes per bit. Xicor NOVRAM technology is implemented differently than standard  $E^2$ PROM technology.  $E^2$ PROMs generally require an erase before write cycle (Xicor  $E^2$ PROMs automatically perform the chore.) This can unnecessarily cycle a bit cell: i.e., when a cell

currently programmed as "0" and new data is also a "0", would require the cell to be erased to a "1" then back to a "0". This is equivalent to two write cycles that effect no change.

The Xicor NOVRAM design "cycles" only those bits in the E<sup>2</sup>PROM array that are in a different state than their corresponding bit in the RAM array, reducing the average cycling of individual bit cells per Store operation. Therefore, the 10,000 store operations and 1000 bit changes specified are not contradictory.

**Question No. 8:** The imminent-power-failure signal in my system is designed to pull STORE low and keep it there throughout the power-down. Will subsequent store cycles be initiated once the first one completes?

**Answer:** No. The  $\overline{\text{STORE}}$  input is falling edge sensitive, so the pin would have to be raised through  $V_{IH}$  and lowered through  $V_{IL}$  to start another cycle.

**Question No. 9:** The X2212 features are perfect for my application. However, the 8048  $\mu\text{P}$  has separate  $\overline{\text{R}}$  and  $\overline{\text{W}}$  pins and uses a multiplexed data bus which creates bus contention between the higher order address bits and the X2212 output. How can I interface these two?

**Answer:** By conditioning the  $\overline{\text{CS}}$  of the NOVRAMs with an active  $\overline{\text{R}}$  or  $\overline{\text{W}}$  signal, the built-in NOVRAM output buffer may be utilized. Figure 6 shows the simple NAND gate logic required. The NOVRAM  $\overline{\text{CS}}$  is only low when the device is selected and  $\overline{\text{R}}$  or  $\overline{\text{W}}$  are low  $\overline{\text{CS}} = (\overline{\text{R}} + \overline{\text{W}})$ . This way the NOVRAM data buffer is tri-stated unless it is being accessed. This makes NOVRAMs static-RAM-simple even in a multiplexed bus environment.

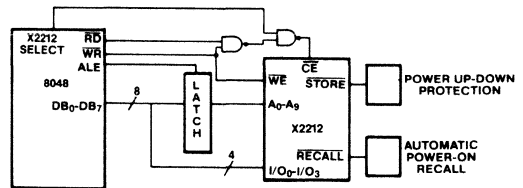


Figure 6: 8048 Microcontroller Implementation

The tremendous versatility of these X2200 dual array memory devices has yet to be fully utilized. Xicor applications engineers are available to address any questions regarding NOVRAMs that you might have.

0004-3

## NOTES

## FOURTEEN COMMON E<sup>2</sup>PROM QUESTIONS ANSWERED

By Rick Orlando

The wide variety of applications for E<sup>2</sup>PROM devices includes remotely alterable control stores and look up tables, calibration parameters, configuration data, nonvolatile counters, user programmable software storage, and artificial intelligence systems which update their algorithms as they learn. The E<sup>2</sup>PROM device features making these applications easier to implement include:

- 5 Volt Only Operation
- TTL Compatible Interface
- Noise Filtered Control Inputs
- 10 Year Nonvolatile Data Retention
- Self-Timed Write Cycle with On-Chip Latches
- Inadvertent Write Protection ( $V_{CC}$  Sensor)
- Transparent Byte Erase (Automated in Write Cycle)

This brief includes fourteen common E<sup>2</sup>PROM questions asked of the Xicor applications department. Frequently, the clarification of these points provides creative engineers with insights into new and unique applications. Should you need additional information, don't hesitate to contact us.

**Question No. 1:** I am concerned about the possibility of inadvertent Write commands being generated on my system bus during power transitions. Is there an easy way to protect the data in the E<sup>2</sup>PROM device?

**Answer:** YES!! Xicor E<sup>2</sup>PROM devices protect against this occurrence. First, there is an on-chip  $V_{CC}$  sensor which inhibits the control inputs when the supply voltage drops below 3 volts. Second, noise protection is standard on the WE input pins. This blocks out spikes and glitches that might otherwise indicate a Write Cycle. Third, a control pin combination is

required so external power-up/down protection is easy to implement.

**Question No. 2:** The Write Cycle timing diagrams on the X2804A and X2816A data sheets show that the internal data latch secures the data upon the first rising edge of WE or CE. In an existing design, external latches supporting the E<sup>2</sup>PROM socket hold these two control signals LOW for the full 10ms period. How can the X2804A and X2816A devices be used without hardware changes to my system?

**Answer:** The Xicor E<sup>2</sup>PROM family is compatible with existing industry standard sockets. The internal data latches on the X2804A and X2816A devices are transparent so that, while not latched, the data on their inputs is passed directly through. This feature makes X2804A and X2816A use in externally latched sockets plug-in simple. Data may be held constant by an external latch, along with the control signals, and the Xicor devices will write perfectly. An economizing suggestion in this case would be to leave the external latches and timers off the board and jumper the control, data, and address busses directly to the E<sup>2</sup>PROM socket. Since Xicor designed all of these functions on-chip, the expense of support hardware required by some competing E<sup>2</sup>PROM manufacturers is eliminated.

**Question No. 3:** The Standby current requirements of the X2804A and X2816A devices is too great for our portable CMOS system. If the  $V_{CC}$  line is switched open, will the E<sup>2</sup>PROM I/O lines load the bus?

**Answer:** No. The output driver for each I/O pin is composed of a matched series pair of enhancement mode NMOS FETs as shown in Figure 1. During normal power-up operation, these drivers are in the HIGH-Z mode whenever the E<sup>2</sup>PROM is not selected. While the device has no power applied, these FETs are not conducting so the output pin presents a HIGH-Z load to the bus. The device input pins are

simply V and I protected FET gates, so there is no loading beyond the input capacitance, and minimal leakage current. The Zener diode input protection allows for signals to be applied to the X2804A and X2816A when the  $V_{CC}$  line is open. The internal  $V_{CC}$  sensor designed into the X2804A and X2816A E<sup>2</sup>PROMs ensures that the control inputs are inhibited whenever  $V_{CC} = 3V$ . Therefore, data integrity is maintained even while  $V_{CC}$  is switched open.

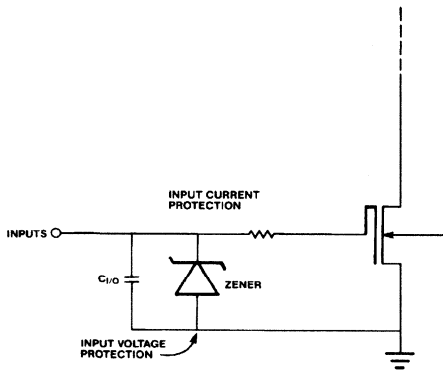


Figure 1a: Input Circuit Model

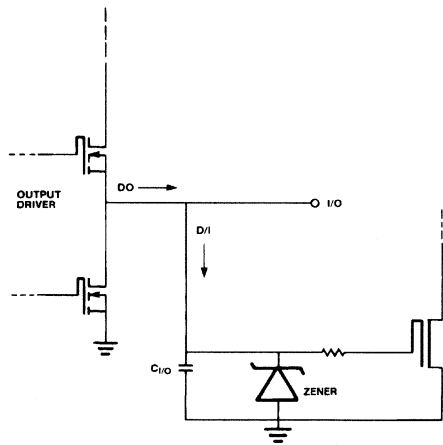


Figure 1b: I/O Circuit Model

Many remote and portable system designs have taken advantage of E<sup>2</sup>PROM nonvolatility through the use of a low on-resistance Power FET which switches supply current to the  $V_{CC}$  line as shown in Figure 2a. The algorithm is shown in Figure 2b. Note that the Power FET must remain enabled for at least 10ms after the initialization of the most recent Write Cycle so that the E<sup>2</sup>PROM power supply remains in-spec for the duration of the nonvolatile Write Cycle.

Since the device is off the bus during this period, the system may optionally perform other tasks while the nonvolatile Write Cycle completes. Where maximum power conservation is necessary, the 10ms power-up period may be reduced to typical (5ms) nonvolatile Write periods by polling the E<sup>2</sup>PROM for HIGH-Z 10ms I/O lines on the X2804A and X2816A (see next question) or utilizing the DATA Polling feature designed into the X2864A.

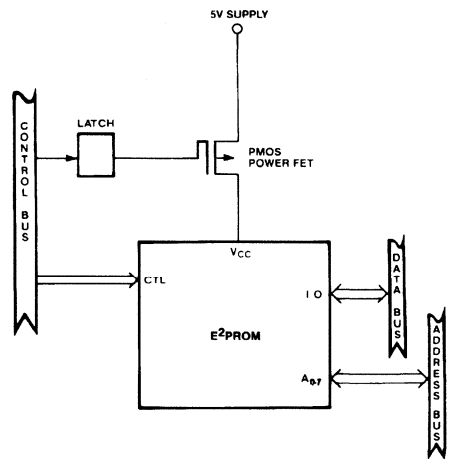


Figure 2a: Use of Low On-Resistance Power FET

**Question No. 4:** The maximum nonvolatile Write Cycle period is specified over the temperature range as 10ms on the X2804A and X2816A E<sup>2</sup>PROMs. What is the typical time required and how might it be utilized?

**Answer:** Typically, these devices complete the nonvolatile Write Cycle in less than 5ms. The cycle is initiated by a standard microprocessor write cycle. As the last of  $\overline{CE}$  or  $\overline{WE}$  falls LOW, the address to be written to is latched into the on-chip address latches. When the first of  $\overline{CE}$  or  $\overline{WE}$  transitions back to HIGH, the data latches lock the data to-be-written on board the chip (see Figure 3). These features make the Xicor E<sup>2</sup>PROM appear as a standard static RAM to the system. The on board timer is initiated when the address is latched and once the data is latched, the device inputs are inhibited and the outputs placed in their HIGH-Z mode, thereby freeing the system to perform other tasks. The E<sup>2</sup>PROM outputs remain floating until the internal operations are complete, at which point, the X2804A and X2816A are immediately available for access.

To take advantage of typical Write times and maximize the multiple byte Write speeds, simply poll the E<sup>2</sup>PROM looping until the floating outputs are no longer detected (see Figure 4). For example, in a



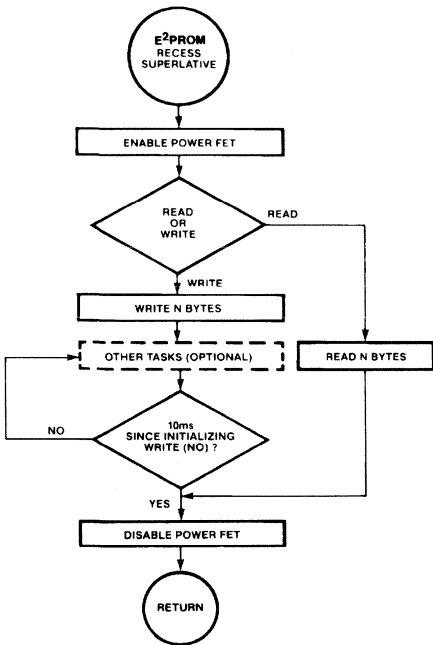


Figure 2b: Algorithm

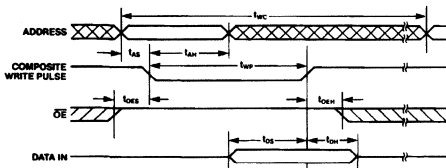


Figure 3: E<sup>2</sup>PROM Timing

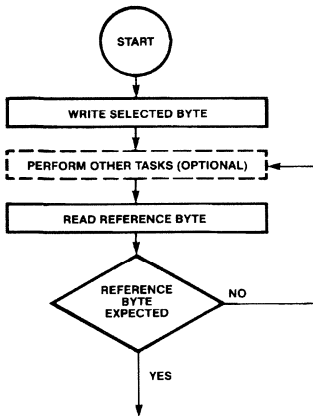


Figure 4: Flow Chart for Interrogation

system with a pulled up bus, 00 (Hex) could be permanently stored in the last address in the E<sup>2</sup>PROM. After the nonvolatile Write Cycle is initiated, the system attempts to read the last location. While the device is still internally occupied, the pullup resistors combined with the HIGH-Z state of the E<sup>2</sup>PROM output buffer, will provide FF (Hex) in response. Immediately upon completion of the nonvolatile Write Cycle, the inputs are again enabled and the Read Cycle will provide valid data from the E<sup>2</sup>PROM. In this example, the software would loop until the data acquired is 00 (Hex).

The X2864A has a software feature designed into it for this purpose. DATA Polling inverts D<sub>7</sub> of the last byte written, and routes it to the output buffer while the device is internally occupied. This way the user simply reads the last address written, comparing the data to the last data written, until they match indicating nonvolatile Write Cycle completion.

**Question No. 5:** How do the Read Access and Write Cycle times change as the E<sup>2</sup>PROM operating temperature varies?

**Answer:** Xicor maximum and minimum specifications are guaranteed over the full operating temperature range of the device. These values are established under worst case conditions and specified with a conservative margin. This means that, invariably in a systems environment, Xicor products perform much better than the data sheet indicates. In terms of actual parameter variation, Read Access time varies proportionately to temperature, and Write Cycle time varies inversely with temperature. They each stay well within their respective maximum specifications throughout the allowable temperature range of the device.

**Question No. 6:** Will signals applied to E<sup>2</sup>PROM pins designated NC (not connected) damage the devices?

**Answer:** No. NC pins have no connections to the device.

**Question No. 7:** How much drive current is required to hold the CE, OE, and WE inputs low?

**Answer:** The input configuration of Xicor E<sup>2</sup>PROMs is shown in Figure 1a and is standard NMOS. Only the leakage current (max 10μa) and enough charge for the 6 pF input must be capacitance driven.

**Question No. 8:** Can the E<sup>2</sup>PROM be read during the 10ms nonvolatile Write Cycle?

**Answer:** No. During the internally timed write, the device inputs are inhibited and its outputs are in a high impedance state. However, once the nonvolatile Write Cycle is complete, (typically <5ms), normal data access may be resumed.

**Question No. 9:** The X2804A and X2816A data sheets make no mention of the standard byte-erase cycle which precedes an E<sup>2</sup>PROM byte-write. Is there something about Xicor E<sup>2</sup>PROMs which eliminates this requirement?

**Answer:** Yes! On Xicor E<sup>2</sup>PROMs, an automatic and user transparent byte erase cycle is initiated as a normal part of the nonvolatile Write Cycle. This feature eliminates the extra time and software required by the other E<sup>2</sup>PROMs.

**Question No. 10:** When interfacing the Xicor E<sup>2</sup>PROMs with a CMOS system are pullup resistors required?

**Answer:** Yes. The V<sub>OH</sub> min specification on the Xicor devices is 2.4V, and the V<sub>IH</sub> min for CMOS technology (when V<sub>DD</sub> = 5V) is 3.5V. To ensure that E<sup>2</sup>PROM HIGH outputs are recognized by the CMOS inputs, pullup resistors are necessary. Of course, CMOS outputs can drive the E<sup>2</sup>PROM inputs directly with no pullup assistance.

**Question No. 11:** We are using an entire bank of military X2864A devices on a common bus. If some of these are enabled and some not when high voltage chip erase cycle is executed, will the not-enabled devices be affected?

**Answer:** No. Those chips which are not enabled will not be modified.

**Question No. 12:** During the Read cycle, the Xicor E<sup>2</sup>PROM outputs go low before stabilizing with valid data. Although the data is valid long before the specified access time, I wonder if this phenomenon is normal?

**Answer:** This operation is perfectly normal when clocking with  $\overline{CE}$ . While  $\overline{CE}$  is HIGH, the device is in a standby state with the power to the output buffers

and sense amps turned off. When  $\overline{CE}$  goes LOW, the output buffers are turned on and the sense amps are reading a LOW until the actual cell-data reaches them. Therefore, with  $\overline{OE}$  LOW and  $\overline{WE}$  HIGH, when  $\overline{CE}$  falls LOW valid data will be preceded by a brief LOW output.

**Question No. 13:** We are using the high voltage Chip Erase function on the military E<sup>2</sup>PROMs to Bulk Erase data so that the data is unavailable to unauthorized copying. Could a highly skilled technologist detect what the data was prior to erasure given enough resources?

**Answer:** No. The floating gate storage mechanism is driven to complete saturation when programmed, and all free electrons are removed upon erasure. Therefore, no trace of a previous state is left when a cell moves to the opposite state. This is one of the features of Xicor nonvolatile technology that makes it perfect for high security military applications.

**Question No. 14:** I am using several X2816As which form contiguous address spaces in my system. Does the "self-timed" feature on these devices mean that I can write to each of them independently during a single 10ms Write Cycle?

**Answer:** EXACTLY! The on-chip timer frees the busses (and therefore the system) for the duration of the write cycle. The on-chip latches are essential for this to be possible. A quick look at the data sheet Write Cycle timing diagram shows that the system can shake hands with the Xicor E<sup>2</sup>PROMs for as little as ( $t_{AS} + t_{WP} + t_{DH} =$ ) 170ns. The other 99.98% of the 10ms write cycle can be spent executing other system tasks which could include initiating write cycles to the other X2816As. This "gang programming" is one simple method of achieving very high effective-byte-write speeds in multiple device systems.

0026-4

## NONVOLATILE DATA INTEGRITY: INADVERTENT WRITE/STORE ELIMINATION

By Applications Staff

Xicor's nonvolatile memory products are backed by designed-in protection features which ensure data integrity. These include:

- **Onboard  $V_{CC}$  Sensor**  
All operations inhibited when  $V_{CC} \leq 3.0V$ .
- **Noise Filter**  
A feature which blocks noise spikes on control lines.
- **Orderly Power Transition**  
The device will not self-generate inadvertent write/store operations.
- **Write/Store Inhibited Control Pins**  
Multi-pin write/store command signal requirements provide both data security *and* design flexibility.

### New Design Features

- Software Write Protection
- Previous Recall Latch
- Command Sequence

With Xicor nonvolatile memories, data is maintained through power-on, power-off, power-down, system crash, and the entire range of system conditions when some simple design rules are observed. Often nonvolatile system designers are frustrated by inadvertent system command signals during power-up and power-down operations. Being nonperiodic in nature, these elusive culprits can lead the designers to the false conclusion that the memory device is malfunctioning. This, however, is rarely the case. The system is more often sending an unintended write/store command. This problem can be easily resolved as shown in this application brief.

### GIGO<sup>1</sup> Going to Sleep

Just as a person falling asleep at the wheel can inadvertently command his vehicle into an undesirable situation, digital systems transitioning from normal operation to a power-off state or vice versa can distribute random data, addresses, and control signals along the way.

Since Xicor nonvolatile memories accurately and reliably store data as instructed, data stored at power-down will be impeccably retained and available upon power-up. (That's nonvolatile GIGO.)

### Protection-Conscious Design

Data integrity is a major criterion with Xicor products and several superb features were designed into Xicor's memories to ensure it.

- **$V_{CC}$  Sensor**  
An onboard sensor establishes a threshold supply voltage of 3.0V below which write operations on E<sup>2</sup>PROMs and store operations on NOVRAMs are blocked. Above this voltage, write and store operations are available and therefore must be protected from unplanned instructions.
- **Orderly Supply Transitions**  
As a system powers up or down, the possibility of unintentional, internally generated control signals increases dramatically. The Xicor nonvolatile memory family has designed-in protection to eliminate self-generated write/store commands.
- **Noise Filter**  
An additional feature designed into Xicor's E<sup>2</sup>PROM family is a noise filter to prevent glitches on the WE line from initiating a write cycle. This feature filters pulses of less than 20ns duration insuring noise spikes are not misconstrued as write commands.

■ **Write/Store Inhibit Control Pins**

Xicor nonvolatile memories require combinational control pin conditions in order to execute a write/store command. By disallowing any one of the required pin conditions, the user can prevent unplanned nonvolatile data changes so that data integrity is maintained.

**Write/Store Pin Conditions**

ARRAY RECALL <sup>2</sup>	STORE	STORE CAPABILITY
X	H	STORE OPERATION DISABLED
L	X	ARRAY RECALL BLOCKS STORE INITIATION (SEE FOOTNOTE 2)
H	L	STORE OPERATION EXECUTED <sup>3</sup>

Figure 1: X2200 NOVRAM Family

CE	OE	WE	WRITE CAPABILITY
X	X	H	(WE) WRITE INHIBIT*
X	L	X	(OE) WRITE INHIBIT
H	X	X	(CE) WRITE INHIBIT
L	H	L	WRITE OPERATION EXECUTED <sup>3</sup>

\* Hard to control during power cycling.

Figure 2: E<sup>2</sup>PROM Family

**External Hardware Implementations**

**Solution I—"Hold-Low" Protection**

The simplest solution is to pull the  $\overline{OE}$  (or ARRAY RECALL) to a logic "0" whenever the supply voltage is below the (5.0-10%) system threshold.

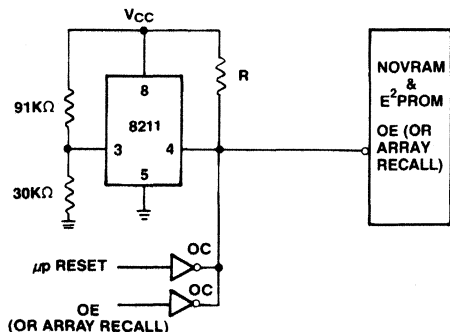


Figure 3: "Hold-Low" Protection

The Intersil<sup>4</sup> ICL 8211 programmable voltage reference is an inexpensive 8-pin mini DIP which will sense a selected voltage threshold and output a logic "0" when the supply is below that threshold. Conversely, as the sensed voltage rises above the selected threshold, the 8211 outputs a logic "1" following its supply voltage level.

**Solution II—"Hold-High" Protection**

The second method of data protection during power supply transitions is to keep the NOVRAM STORE pin (or the WE and/or CE pins in the E<sup>2</sup>PROM family) near the power supply voltage. By preventing the low condition of these pins which is necessary for a write or store operation, inadvertent stores will be eliminated.

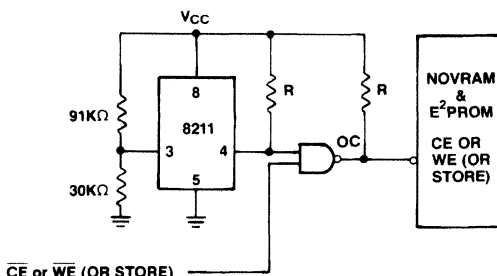


Figure 4: "Hold-High" Protection

The graph in Figure 5 shows the performance of the Intersil ICL 8211. The top plot is a sawtooth which is connected to "5V supply" as shown in the Solution I and Solution II schematic diagrams. The bottom plot is the output of the ICL 8211. Note that when the supply is above 4.50V, the ICL 8211 output tracks it at logic "1". When the supply sawtooth is below 1.56V, the ICL 8211 output tracks the power supply. However, since the Xicor memory family has internal protection inhibiting write/store operations when V<sub>CC</sub> is below 3V, no inadvertent write/stores will occur in this range. In the critical range between 3V, where internal protection stops, and 4.5V, where normal operation begins, the ICL 8211 insures a 0V output.

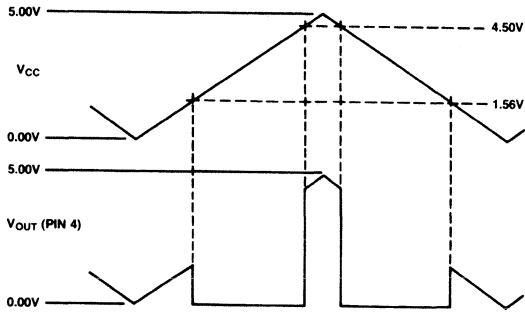


Figure 5: Intersil ICL 8211 Programmable Voltage Reference/Supply and Output Waveforms

As an alternate approach to the 8211, some designers may prefer to incorporate the SGS L487. This device is a 500 mA precision 5V voltage regulator which includes an open collector power-on, power-off reset output pin, which can protect the nonvolatile memories just as the 8211 does. The timing diagram in Figure 6 shows the voltage on this reset output pin as the supply voltage transitions through power-up and power-down.

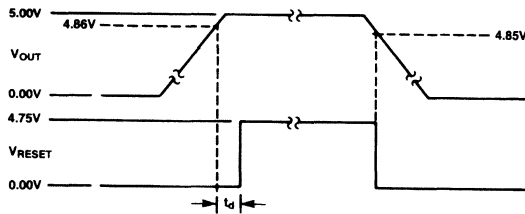


Figure 6: SGS L487 Precision Voltage Regulator/Output and Reset Waveforms

## New Protect Features

### Serial Device Protection X2444

A Previous Recall latch and Write Enable latch have been incorporated in the X2444 Serial NOVRAM.

Upon power-up, both latches will be in the reset state. Both latches must be set in order to enable either a write RAM operation or store to E<sup>2</sup>PROM operation.

A recall operation copies data from the E<sup>2</sup>PROM array into the RAM array. This operation places known data in all RAM locations and sets the previous recall latch. This prevents the user from inadvertently writing one word to RAM and performing a store operation with unknown data in all other locations.

The WREN instruction sets the Write Enable latch, enabling (if the Previous Recall latch is set) write and store operations. The WRDS instruction resets the latch, disabling write and store operations.

Therefore, total data integrity can be maintained through the use of software commands. The device is inherently protected during power-up and, through proper software control, is protected during power-down.

### X2404 Serial E<sup>2</sup>PROM

Due to the nature of the software protocol involved in writing to the X2404, inadvertent stores are highly unlikely. During power-up or power-down the possibility of the bus duplicating the start condition, slave address and transmitting data successfully is so remote as to be unmeasurable.

### Software Write Protection

Future E<sup>2</sup>PROM products will contain a register which is accessible through a software sequence algorithm. This feature provides the user control in selecting the level of write protection required by their application. Refer to the X28256 data sheet for details.

Figure 7 indicates the write protection features incorporated in all Xicor products.

GENERIC DEVICE TYPE	V c c S E N S E	N O I S E F I L T E R	S E L F - P R O T E C T	I N H I B I T G E N E R A T E	P R E V I O U S C O N T R O L	S O F T W A R E R E C A L L	C O M M A N D P R O T E C T I O N	S E Q U E N C E
X2201A	X	X	X	X	X			
X2210	X	X	X	X	X			
X2212	X	X	X	X	X			
X2001	X	X	X	X	X			
X2004	X	X	X	X	X			
X2444	X	X	X	X	X	X		
X2804A	X	X	X	X	X			
X2816A	X	X	X	X	X			
X2816B	X	X	X	X	X			
X2864A	X	X	X	X	X			
X2864B	X	X	X	X	X			
X2864H	X	X	X	X	X			
X28256	X	X	X	X	X		X	
X28C256	X	X	X	X	X		X	
X2404	X	X	X	X	X			X
X24C04	X	X	X	X	X			X
X24C16	X	X	X	X	X			X

Figure 7: Product Protection Matrix

### Footnotes

- <sup>1</sup> GIGO is an acronym popular in the computer world for "Garbage In Garbage Out".
- <sup>2</sup> ARRAY RECALL blocks all control inputs but does not halt a store in process.
- <sup>3</sup> These are the *only conditions* allowing nonvolatile data change.
- <sup>4</sup> See Intersil ICL 8211, ICL 8212 Programmable voltage reference data sheet in Intersil Data Book.

## X2816A DESIGN ALLOWS UPGRADE TO X2864A AND BEYOND

By Rick Orlando

With the announcement of the X2864A, customers have expressed a desire to design an X2816A socket that can be upgraded to accept the X2864A. The 28-pin footprint of the X2864A allows eventual migration up to the 256K bit level. If a board design is done properly, the socket can accept the entire product family.

First, let us look at the "universal socket".

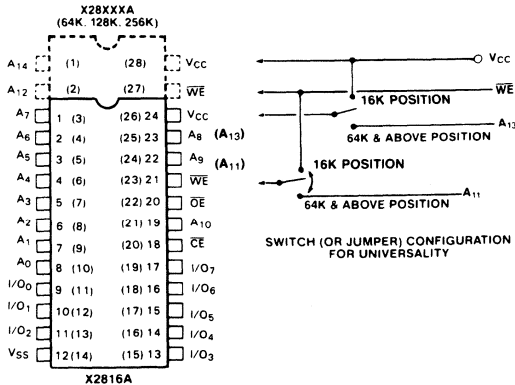


Figure 1. Universal Socket for 16K Thru 256K E<sup>2</sup>PROMs

One can see that the socket will accept Xicor E<sup>2</sup>PROMs from the 16K level through the 256K level with essentially two jumpers determining which footprint the socket is to be.

The next question is how can one minimize the address decoding logic for a board populated with the above "universal" sockets. We will assume that we have a board with eight "universal" sockets. We would like to design the address decoding logic to allow the eight X2816A's to be replaced by two X2864A's.

Now, we look at the addresses that each chip will be mapped into:

	Chip #	Address Range
X2816A	(1)	0000 - 07FF
	(2)	0800 - 0FFF
	(3)	1000 - 17FF
	(4)	1800 - 1FFF
	(5)	2000 - 27FF
	(6)	2800 - 2FFF
	(7)	3000 - 37FF
	(8)	3800 - 3FFF
X2864A	(1)	0000 - 1FFF
	(2)	2000 - 3FFF

Figure 2. Address Map Comparison

The breakdown of the decoding for such a scheme is listed as follows:

A <sub>15</sub>	A <sub>14</sub>	A <sub>13</sub>	A <sub>12</sub>	A <sub>11</sub>	X2816A Chip Selects*								X2864A Chip Selects*			
					1	2	3	4	5	6	7	8	1	2		
0	0	0	0	0	0	1	1	1	1	1	1	1	1	1	0	1
0	0	0	0	0	1	1	0	1	1	1	1	1	1	1	0	1
0	0	0	1	0	1	1	0	1	1	1	1	1	1	1	0	1
0	0	0	1	1	1	1	1	0	1	1	1	1	1	1	0	1
0	0	1	0	0	1	1	1	1	0	1	1	1	1	1	1	0
0	0	1	0	1	1	1	1	1	1	0	1	1	1	1	1	0
0	0	1	1	0	1	1	1	1	1	1	0	1	1	1	1	0
0	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	0

\*Chip Select is active low.

Figure 3. Address Decode Comparison

One possible solution is to use two 74LS138's with one being wired for the X2816A and one for the X2864A. If the X2816A's are used in the board, LS138-A is installed and LS138-B is omitted. Conversely, if X2864A's are being used, LS138-B is installed and LS138-A is omitted.

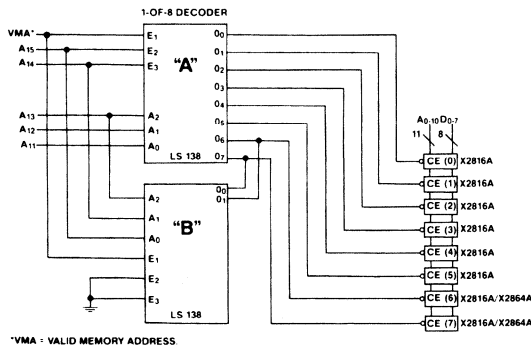


Figure 4. 74LS138 Decode Wiring Option

The two X2864A's are placed in sockets 6 and 7.

Another solution for the address mapping questions is to use a 32x8 bipolar PROM for address decoding.

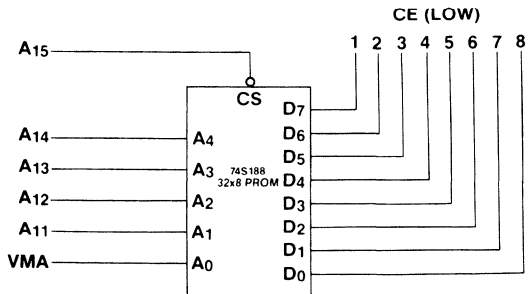


Figure 5. Bipolar PROM Mapping

One simply changes the PROM for replacing the X2816A's with X2864A's.

Another related case is where the designer would like to increase the memory capacity of the board by upgrading to the X2864A. In this case, we need to replace the eight X2816A's (128K bits/board) with eight X2864A's (512K bits/board).

Using the "universal" sockets, this is relatively easy. We use the following circuit, again using a 32x8 bipolar PROM.



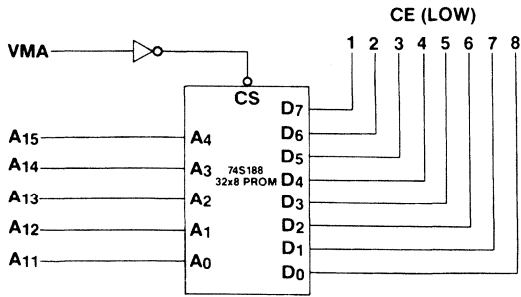


Figure 6. Bipolar PROM Mapping for Memory Expansion

One simply changes the program in the PROM to go from using X2816A's to X2864A's. The listing below shows the PROM program for the X2816A's and the X2864A's.

The PROM decode method allows a mixed combination of X2816A's and X2864A's to be used on the same board. It also allows different types of memory to be used such as X2816A's and 64K CMOS RAMs on the board. If the board is to be used with either 16K or larger devices, then only two jumpers are needed per board to configure all of the "universal" sockets.

The address decoding can be extended even further to incorporate expansion to the 256K bit E<sup>2</sup>PROM.

One can see that through using foresight in design, a modern designer can implement a memory socket that is truly universal in allowing the use of the most cost-effective E<sup>2</sup>PROM densities available.

16K Bytes X2816A Program 0000 - 3FFF													64K Bytes X2864A Program 0000 - FFFF								
A <sub>11</sub>	A <sub>12</sub>	A <sub>13</sub>	A <sub>14</sub>	A <sub>15</sub>	D <sub>0</sub>	D <sub>1</sub>	D <sub>2</sub>	D <sub>3</sub>	D <sub>4</sub>	D <sub>5</sub>	D <sub>6</sub>	D <sub>7</sub>	D <sub>0</sub>	D <sub>1</sub>	D <sub>2</sub>	D <sub>3</sub>	D <sub>4</sub>	D <sub>5</sub>	D <sub>6</sub>	D <sub>7</sub>	
0	0	0	0	0	0	1	1	1	1	1	1	1	0	1	1	1	1	1	1	1	1
1	0	0	0	0	1	0	1	1	1	1	1	1	0	1	1	1	1	1	1	1	1
1	1	0	0	0	1	1	0	1	1	1	1	1	0	1	1	1	1	1	1	1	1
1	1	0	0	0	1	1	1	0	1	1	1	1	0	1	1	1	1	1	1	1	1
0	0	1	0	0	1	1	1	1	0	1	1	1	1	0	1	1	1	1	1	1	1
1	0	1	0	0	1	1	1	1	1	0	1	1	1	0	1	1	1	1	1	1	1
0	1	1	0	0	1	1	1	1	1	1	0	1	1	0	1	1	1	1	1	1	1
1	1	1	0	0	1	1	1	1	1	1	1	0	1	0	1	1	1	1	1	1	1
0	0	0	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
1	0	0	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
0	1	0	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
1	1	0	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
0	0	1	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
1	0	1	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
0	1	1	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
1	1	1	1	0	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1	1
0	0	0	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
1	0	0	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
0	1	0	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
1	1	0	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
0	0	1	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
1	0	1	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
0	1	1	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
1	1	1	0	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1	1
0	0	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1
1	0	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1
0	1	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1
1	1	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1	1
0	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1	1
1	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1	1
0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0	1
1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	0

Figure 7. PROM Contents for Memory Expansion Mapping

## NOTES

## REPLACING DIP SWITCHES WITH NONVOLATILE TECHNOLOGY

By Rick Orlando

One of the most prevalent applications for small nonvolatile memories is that of replacing DIP switches. The advantages of the nonvolatile memories is clear. They take up less room, are easier to use, and lend themselves to automated board assembly. 256 bits of information, or the equivalent of 32, 8-bit DIP switches can be implemented in a single package.

Xicor's new X2444 Serial NOVRAM adds yet another feature—low cost. When coupled with the serial device's minimal interface requirements, the X2444 takes DIP switches head on, and is obviously the cost/performance leader. The purpose of this brief is to describe how easy it is to replace a DIP switch with an X2444 NOVRAM.

### DIP Switch Interface

There are two common types of DIP switch interfaces.

### I/O Port

The first uses an I/O port with internal pullup resistors. Figure 1a shows a typical circuit that could be used either with a single chip microcomputer or with an I/O port on a microprocessor bus. In either case, the internal pullups present a logic "1" to the input as long as the DIP switch is open. To use an X2444 Serial NOVRAM in the DIP switch socket, one only needs to tie pins 14, 15, and 16 of the 16-pin socket to  $V_{CC}$ .

One then plugs an X2444 part in the uppermost half of the socket, and the circuit becomes that shown in Figure 1b.  $V_{CC}$ , STORE, and RECALL are tied hard to 5 volts, so that all nonvolatile operations are controlled through software. The four interface lines from the X2444 are connected to the four least significant I/O lines of the port.

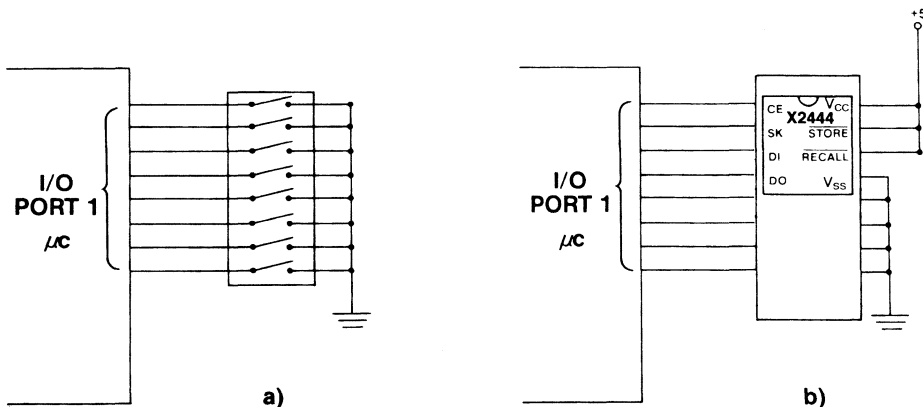


Figure 1. Microcomputer with Internal Pullups

## No Internal Pullups

The second type of interface uses ports which do not have internal pullups. In this instance, the X2444 can be plugged into the top section of the pullup resistor socket, with a jumper from pin 13 of the 16-pin site to ground, for the  $V_{SS}$  on the serial part.

Again,  $V_{CC}$ , STORE, and RECALL are tied to +5V through the connections used for the resistor pack. The DIP switch socket simply remains empty. See Figure 2.

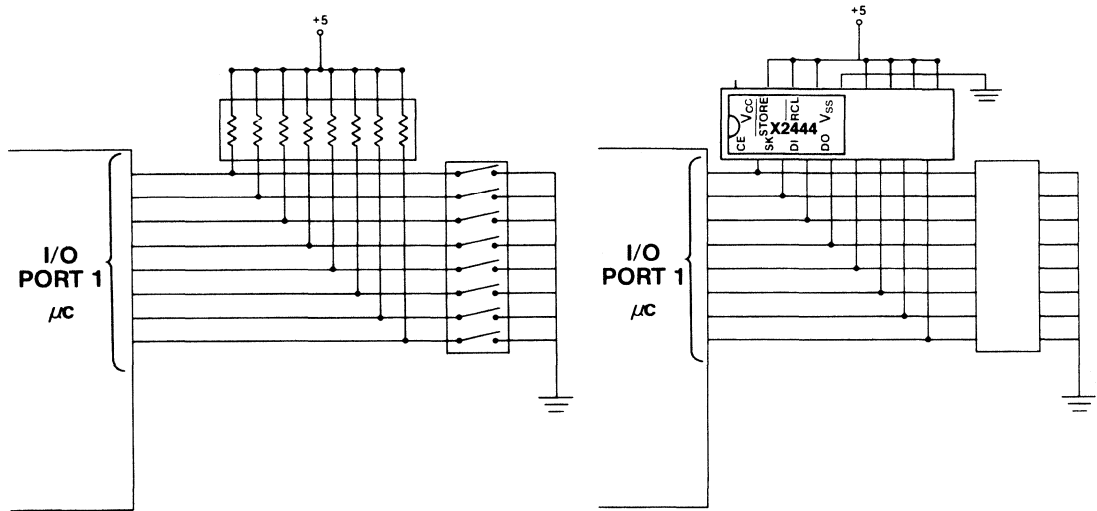


Figure 2. Microcomputer without Internal Pullups

Both of these implementations free up four more I/O lines to be used elsewhere. They also require the same software to drive the X2444.

Assume that the processor is a 6801 with the X2444 replacing a DIP switch. The procedure "INIT" initializes the port (see Section 1, "X2444 Driver Program for 6801").

Serial output is accomplished by loading the data to be output into the A Accumulator. A loop routine then shifts a bit into the carry, sets the serial data out (Data in for X2444) to either a "1" or "0" depending upon the state of the carry and toggles the clock.

(See Section 2 Procedure "SHIFT1" of X2444 Driver Program for further details).

The serial input is performed by a loop which examines the state of the serial data in, (Data out for X2444) sets the carry accordingly, shifts the carry into the accumulator and toggles the clock. (See Section 3 Procedure "SHIFTIN" of X2444 Driver Program for further details).

The complete software is as follows, and it occupies about 100 bytes of code. As one can see, the X2444 is indeed a value replacement for DIP switches.

```

*****
;                               6801 X2444 DRIVER
; ASSUME THAT PORT1 IS USED AS THE 2444 INTERFACE
; PORT1'S REGISTERS ARE LOCATED AS FOLLOWS
; DATA DIRECTION          HEX 0000
; PORT                     HEX 0002
;
; I/O 0                    SERIAL CLOCK   SERIAL CLOCK
; I/O 1                    SERIAL OUT     SERIAL IN
; I/O 2                    SERIAL IN     SERIAL OUT
; I/O 3                    2444 SELECT    CHIP SELECT
;
;
; COMMANDS ARE PASSED TO THE X2444 ROUTINE BY A PARAMETER IN THE
; ACCUMULATOR, WHILE THE ADDRESS IF NEEDED IS PASSED ON THE STACK
; SERIAL DATA IN OR OUT USES THE TEMPORARY LOCATION TEMP1,
; WHICH IS A SIXTEEN BIT WORD. THE X2444 COMMANDS ARE ENCRYPTED AS
; FOLLOWS.
; COMMAND CODE             INSTRUCTION      OPCODE
; 0                        READ             1AAAA11X
; 1                        WRITE            1AAAA011
; 2                        RESET WRITE ENBLE 11111000
; 3                        STORE           11111001
; 4                        SLEEP           11111010
; 5                        SET WRITE ENBLE  11111100
; 6                        RECALL          11111101
; *1*'S ARE USED INSTEAD OF DON'T CARE TO DISTINGUISH BETWEEN DATA AND
; NON DATA OPERATIONS.
*****

```

```

DIRECTION1 .EQU 00.
PORT1 .EQU 000H ;RAM STORAGE FOR DATA
TEMP1 .EQU 082H ;COUNTER VARIABLE
COUNT .EQU 084H ;DATA STORAGE
DATUM .EQU 084H ;DATA STORAGE
ADDRESS .EQU 086H ;ADDRESS STORAGE
ERRORDATA .EQU 08BH ;ERROR DATA

```

**Section 1**

```

*****
; PROCEDURE INIT
; THIS PROCEDURE INITIALIZES THE X2444 INTERFACE
*****
INIT LDAA #1BH ; B=1011, I/O 0+1 AND 3 OUTPUTS, 2 INPUT
STAA DIRECTION1 ; WRITE TO DATA DIRECTION REGISTER
CLRA ; SET CE TO 0 (INACTIVE), DOUT AND SK TO 0
STAA PORT1 ; AND STORE IN DATA PORT
RTS ;

```

**Section 2**

```

*****
; SHIFTER ROUTINE- SHIFT1
; THIS ROUTINE TAKES THE DATA IN THE A ACCUMULATOR AND CLOCKS IT MOST
; SIGNIFICANT BIT FIRST INTO THE X2444. THE FLOW IS SHIFT A BIT, TOGGLE
; THE SERIAL OUTPUT(6801) ACCORDING TO STATE, AND TOGGLE SERIAL CLOCK
*****
SHIFTOUT LDAB #08. ;LOAD THE BIT COUNT WITH 8
STAB COUNT ;STORE IN COUNTER
SHIFT1 ROLA ;SHIFT BIT INTO CARRY BIT
LDAB #14H ;WE SET DATA OUT TO ZERO, WHILE SETTING CHIP
;ENABLE. SERIAL CLOCK IS LOW.
BCC TRANS ;IF BIT IS A ZERO, THEN TRANSMIT
ORAB #02H ;IF IT IS A ONE, THEN SET DATA OUT
STAB PORT1 ;STORE THE DATA INTO THE PORT
ORAB #01H ;AND SET THE CLOCK FOR A TRANSITION
STAB PORT1 ;BY WRITING A 1 TO SERIAL CLOCK
ANDB #10H ;KEEP THE DATA VALID, BUT SET SK TO ZERO
STAB PORT1 ;AND STORE IN THE PORT
LDAB #14H ;TOGGLE CLOCK DOWN, SET DOUT TO 0, BUT KEEP
STAB PORT1 ;X2444 SELECTED
DEC COUNT ;DECREMENT THE BIT COUNTER
BNE SHIFT1 ;IF COUNT IS NOT ZERO, TRANSMIT NEXT BIT
ROLA ;ONE MORE ROTATE TO PRESERVE INSTRUCTION
RTS ;RETURN FROM SUBROUTINE

```

**Section 3**

```

*****
; SHIFTER ROUTINE
; THIS SUBROUTINE SHIFTS IN 8 BITS OF DATA INTO THE A ACCUMULATOR FROM THE
; X2444. THE METHOD IS TO ENTER WITH THE CLOCK LOW, TOGGLE THE SERIAL CLOCK,
; EXAMINE THE INPUT DATA, AND SHIFT IT INTO THE A ACCUMULATOR. THIS IS DONE
; 8 TIMES. THE ROUTINE IS EXITED WITH THE CHIP DESELECTED, AND THE BYTE
; READ FROM THE CHIP IN THE A ACCUMULATOR
*****
SHIFTIN LDAB #8. ;LOAD THE BIT COUNT
STAB COUNT ;AND STORE IT IN THE COUNTER
NEXT LDAB #04 ;AT THIS POINT THE X2444 SHOULD BE SELECTED
BITB PORT1 ;THEREFORE, WE DO NOT NEED TO SELECT CHIP
CLC ;MASK BIT FOR I/O 2 OF PORT
BEQ CLOCK ;CHECK TO SEE IF INPUT IS A ONE OR ZERO
SEC ;CLEAR THE CARRY
;IF IT IS A ZERO, LEAVE CARRY AT 0
;OTHERWISE SET CARRY TO LOAD INTO A
LDAB #15H ;SEND A CLOCK TO X2444, BUT KEEP CHIP SELECT HIGH
STAB PORT1 ;BY WRITING A 1 TO SERIAL CLOCK OUTPUT
LDAB #14H ;SET UP TO CLEAR CLOCK, BUT KEEP X2444 SELECTED
STAB PORT1 ;AND STORE
ROLA ;ROTATE CARRY INTO LSB OF ACCUMULATOR A
DEC COUNT ;DECREMENT COUNTER
BNE NEXT ;IF NOT ZERO, THEN WE ARE NOT DONE, GET NEXT
RTS ;AND RETURN FROM SUBROUTINE

```

```

;*****
; X2444 DRIVER ROUTINE
; IT IS ASSUMED THAT THE INSTRUCTION IS PASSED IN THE A ACCUMULATOR. AN
; ADDRESS, IF NEEDED, IS PASSED ON THE STACK(CURRENT SF--2)
; DATA TO BE READ OR WRITTEN WILL BE HELD IN TEMP1
;*****
DRIVE  CMPA    #0FBH      ;CHECK TO SEE IF IT IS READ OR WRITE
      BCE     NONDATA    ;IF NOT, THEN BRANCH AROUND
      TSX     ;TRANSFER STACK TO INDEX REGISTER
      DRAA    2,X        ;THE ADDRESS SHOULD BE SF+2
      JSR     SHIFTOUT   ;OUTPUT THE INSTRUCTION
      ANDA    #04H      ;CHECK TO SEE IF IT IS A READ OR WRITE
      BNE     RD         ;IF AC3=1, IT IS A READ

WRT    LDAA    TEMP1      ;IF IT IS A WRITE, GET THE FIRST BYTE
      JSR     SHIFTOUT   ;WRITE THE FIRST BYTE
      LDAA    TEMP1+1    ;GET THE SECOND BYTE
      JSR     SHIFTOUT   ;WRITE THE SECOND BYTE
      BRA     DONE       ;WRITE INSTRUCTION COMPLETE

RD     JSR     SHIFTOUT   ;GET THE FIRST BYTE
      STAA    TEMP1      ;STORE IN TEMP1
      JSR     SHIFTOUT   ;GET THE SECOND BYTE
      STAA    TEMP1+1    ;STORE IN TEMP1+1
      BRA     DONE       ;READ COMPLETE

NONDATA
DONE   CLRA     ;OUTPUT THE INSTRUCTION
      STAA    PORT1     ;DESELECT THE X2444 BY MAKING CS 0
      RTS     ;RETURN FROM SUBROUTINE
;*****
; MAIN INSTRUCTION ROUTINES- COULD BE MACROS
;*****
; READ ROUTINE
; ASSUMES THAT THE ADDRESS IS IN THE A ACCUMULATOR, DATA IS LEFT IN X REGISTER
;*****
READ   ASLA    ;SHIFT THE ADDRESS 3 TIMES TO LINE IT
      ASLA    ;UP WITH THE INSTRUCTION FIELD
      ASLA
      PSHA    ;PUSH ADDRESS ON THE STACK
      LDAA    #0B7H     ;LOAD INSTRUCTION INTO A ACCUMULATOR
      JSR     DRIVE     ;PERFORM INSTRUCTION
      LDX     TEMP1     ;GET THE RESULT IN THE INDEX REGISTER
      FULA    ;CLEAN UP THE STACK
      RTS     ;AND RETURN
;*****
; WRITE ROUTINE
; ASSUMES THAT THE ADDRESS IS IN THE A ACCUMULATOR, DATA TO WRITE IS IN THE
; X REGISTER.
; ALSO CALLS SET WRITE ENABLE LATCH ROUTINE(SWREN) TO ENABLE THE WRITE OPERATION
;*****
WRITE  ASLA    ;SHIFT THE ADDRESS 3 TIMES
      ASLA
      ASLA
      PSHA    ;PUSH ADDRESS ONTO THE STACK
      JSR     SWREN     ;SET THE WRITE ENABLE LATCH
      LDAA    #0B3H     ;LOAD WRITE INSTRUCTION
      STX     TEMP1     ;STORE DATA IN TEMP1
      JSR     DRIVE     ;PERFORM INSTRUCTION
      FULA    ;CLEAN UP STACK
      RTS
;*****
RWREN  LDAA    #0FBH     ;LOAD THE INSTRUCTION
      JSR     DRIVE     ;AND EXECUTE
      RTS
;*****
STORE  LDAA    #0F9H     ;LOAD THE INSTRUCTION
      JSR     DRIVE     ;PERFORM OPERATION
      RTS     ;AND RETURN
;*****
SLEEP  LDAA    #0FAH     ;LOAD THE INSTRUCTION

```

0006-4

## USING DATA POLLING IN AN INTERRUPT DRIVEN ENVIRONMENT

By Rick Orlando

The use of interrupt driven system design has become increasingly popular in many applications. Interrupt driven systems usually can achieve higher performance and improved user friendliness. An interrupt driven system can perform a variety of tasks while waiting for a certain condition to occur, rather than constantly looping and waiting for the occurrence. Writing to E<sup>2</sup>PROMs is no exception. Since the devices take a relatively long period to complete a Write Cycle, the system could perform a variety of tasks in the meantime.

DATA Polling was introduced on the X2864A to allow notification to the processor of Write Cycle completion. The manner in which it works is quite simple. The processor first writes a byte of data into the E<sup>2</sup>PROM. Any subsequent reads to any location of the chip will produce the complement of the data last written (hence, the name DATA Polling) until the E<sup>2</sup>PROM's internal Write Cycle is complete. At this point, reads to any location in the E<sup>2</sup>PROM will result in the valid data at that location. It can be seen that one can simply write a byte, and then perform frequent compares of the data in the location just written. The data will not be correct until the chip has completed its internal Write Cycle, and the Data circuitry is disabled.

In applications where the processor does not have anything to do during the Write Cycle, the software can simply perform compare loops until the Write Cycle is complete, and then write the next byte. In applications which are more processing time limited, a test loop can be placed in the main program loop, which will check the status of a previous Write Cycle on each pass through the main or outermost software loop. Almost all microprocessor applications software has such a top level loop. DATA Polling is obviously adequate in these environments.

The interrupt intensive applications may not have a main control loop nor can they usually afford the processing time for the processor to sit and loop until the Write Cycle is complete. In these applications, it would be ideal if the Write Cycle completion notification could be interrupt controlled. Although it is not obvious, DATA Polling can be used in these applications as well.

It should be noted that the whole reason for Write Cycle notification is because the typical write times for the E<sup>2</sup>PROMs are substantially shorter than the specified maximums. The magnitude of the delta between the typical and the maximum values determines the importance of the Write Cycle notification. One can easily see that if the maximum Write Cycle time and the typical were equal, one would only have to time a fixed interval for each Write Cycle, either from a software loop or a hardware timer. The hardware timer would generate an interrupt 10 msec after the Write Cycle was initiated, and the next byte could be written. Keep in mind that the discussion of write times for E<sup>2</sup>PROMs are in terms of msec rather than the  $\mu$ sec in which the processor executes instructions. A few  $\mu$ secs here or there are not important when compared to the Write Cycle time of about 10 msec.

DATA Polling does not require any additional hardware interface in order to be used. It is an exclusively software oriented method for determining Write Cycle completion. Even in an interrupt environment, no additional circuitry is required, since all of the interface to the chip occurs through the data and address bus.

In order to use DATA Polling in an interrupt driven system, one only needs a time-based interrupt generator. This could be a programmable timer or even something as simple as an AC frequency interrupt. The key is that the processor does not check to see if the device has completed the Write Cycle until the interrupt occurs. The interrupt routine simply compares the data last written to the E<sup>2</sup>PROM to the data coming from the E<sup>2</sup>PROM. If the two match, the device can be written again. If not, the processor simply returns from the interrupt routine to where it was and continues processing until the next interrupt. The interrupt source is maskable which prevents the overhead of servicing the periodic interrupt during the intervals when a write has not been performed.

A programmable timer or counter is the most elegant solution. Figure 1 shows the hardware configuration of a typical system with the E<sup>2</sup>PROM and the programmable timer on the bus. It should be noted that no unusual circuitry is needed from the E<sup>2</sup>PROM socket, which preserves its usefulness as a truly universal socket. The timer interrupt output drives one of the processor's interrupt lines. Many systems already have such a timer on the bus, and as a result require no additional hardware changes to implement this method.

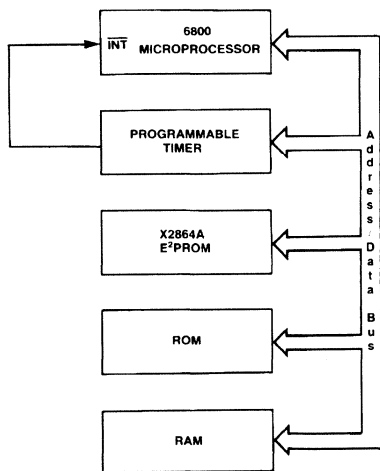


Figure 1: Hardware Configuration of a Typical System with the E<sup>2</sup>PROM and the Programmable Timer on the Bus

The software implementation is rather simple. Figure 2 shows an example of how it might be done using a 6800 microprocessor and a simple timer. The timer control and data registers are mapped into the memory locations described in the initial header along with the temporary RAM variables, which are used to store the last data written and its address.

The write routine (WEEPROM) initially checks to see if the E<sup>2</sup>PROM is ready to perform a write. If not, it simply exits with an error code to show that the write has not taken place. If the write is performed, the timer is loaded with the initial count for 4 msec, and the timer interrupt is enabled. The processor then goes off and performs its normal duties until the interrupt takes place. At that point, the interrupt routine (CKEEP) is entered. It first checks for the proper data that was written to see if the write is complete, using DATA Polling. If it is, the ready flag is set, and the routine is exited. If not, the counter is loaded with a smaller increment, such as 500  $\mu$ sec until the chip's Write Cycle is completed. This essentially allows the majority of the Write time to pass (4 msec) before the processor checks at the more frequent interval of every 500  $\mu$ sec.

Five hundred  $\mu$ sec has been chosen in this example for the interrupt granularity. The value used for a particular application should be chosen based upon the actual system requirements.

One can see that this implementation is rather easy and can be performed with hardware that already may exist in the system. By using the periodic interface approach, the system has the advantage of using an interrupt driven write algorithm, while maintaining only a software interface to the E<sup>2</sup>PROM. Most of the "bookkeeping" sections of the example code are the same as one would use with any method of write termination notification. The end result of using DATA Polling in an interrupt environment is optimization of the Write Cycle period as well as preservation of the pinout of the universal 28-pin socket for expansion through the 256K bit level for E<sup>2</sup>PROMs.



PAGE - 1 DATA\_COD  
File: :DATA\_CODE.TEXT

CODE FOR DATA POLLING IN INTERRUPT ENVIRONMENT, 6800 VERSION

```

0000:                                     .PROC DATA_CODE
Current memory available:      4380
0000: ;*****
0000: ; SAMPLE CODE FOR USING DATA POLLING IN INTERRUPT ENVIRONMENT
0000: ; THIS CODE SHOWS AN EXAMPLE OF HOW TO USE DATA POLLING IN A
0000: ; INTERRUPT DRIVEN WRITE MODE
0000: ;*****
0000: ; MEMORY LOCATIONS
0000: 0100: TIMER .EQU 0100H ;LOCATION OF TIMER DATA REGISTER(COUNT DOWN VALUE)
0000: ;16 BIT VALUE(2 BYTES)
0000: 0102: CTIMER .EQU 0102H ;TIMER CONTROL REGISTER
0000: 0103: LASTA .EQU 0103H ;RAM LOCATION FOR LAST WRITTEN DATA
0000: 0104: TEMP .EQU 0104H ;RAM LOCATION FOR LAST ADDRESS WRITTEN
0000: 0106: ERROR .EQU 0106H ;ERROR FLAG FOR WRITE
0000: 0107: READY .EQU 0107H ;MEMORY READY FOR NEXT WRITE FLAG
0000: 0108: CONFIG .EQU 0108H ;TIMER CONFIGURATION BYTE
0000:
0000: .ORG 0F000H
F000: ;*****
F000: ; EEPROM WRITE ROUTINE
F000: ; THIS ROUTINE WRITES A BYTE OF DATA PASSED IN THE A ACCUMULATOR INTO
F000: ; THE EEPROM AT LOCATION POINTED TO BY THE VALUE IN THE X INDEX REGISTER.
F000: ; THE ROUTINE THEN INITIALIZES THE DATA IN THE COUNTER TO 4096, SINCE THE TIMER
F000: ; COUNTS AT A 1 MHZ FREQUENCY. THIS WILL TIME OUT THE INITIAL 4 MSEC OF THE WRI
F000: ; WRITE CYCLE. THE ROUTINE THEN ENABLES THE INTERRUPTS AN RETURNS CONTROL TO
F000: ; THE CALLING ROUTINE
F000: ;*****
F000: WEEPROM LDAB #00H ;COMPARE TO SEE IF THE MEMORY IS READY FOR WRITE
F002: F1 0107 CMPB READY ;CHECK MEMORY LOCATION READY
F005: 27 ** BEB WRITE ;IF READY THEN WRITE
F007: C6 00 LDB #00H ;OTHERWISE SET THE ERROR FLAG
F009: F7 0106 STAB ERROR ;AND STORE IT IN ERROR
F00C: 20 ** BRA EXIT ;AND EXIT
F00E: A7 00 WRITE STAA 0x ;WRITE THE DATA IN A TO LOCATION X
F010: E7 0103 STAA LASTA ;STORE DATA IN RAM AT LASTA
F013: F1 0104 STX TEMP ;AND STORE LOCATION IN EEPROM AT TEMP
F016: C6 10 LDB #10H ;LOAD THE FIRST BYTE OF 4096 HEX INTO B ACCUMULATOR
F018: F7 0100 STAB TIMER ;WRITE TO TIMER DATA REGISTER
F01E: C6 00 LDB #00H ;LOAD THE SECOND BYTE OF 4096 HEX
F01D: F7 0101 STAB TIMER+1 ;STORE IN THE LSB OF TIMER REGISTER
F020: F6 0108 LDB CONFIG ;GET THE TIMER INITIALIZATION CODE
F023: F7 0102 STAB CTIMER ;STORE IT IN THE TIMER CONTROL REGISTER
F026: 0E CLI ;CLEAR INTERRUPT MASK TO LET TIMER INTERRUPT
F027: 39 RTS ;RETURN FROM SUBROUTINE
F028: ;*****
F028: ; CHECK EEPROM ROUTINE
F028: ; THIS ROUTINE CHECKS TO SEE IF THE EEPROM IS DONE. IT IS ENTERED
F028: ; EVERY TIME THAT THE INTERRUPT IS GENERATED FROM THE TIMER. IT COMPARES
F028: ; THE DATA AT LOCATION TEMP IN THE EEPROM WITH THE DATA THAT IS STORED IN
F028: ; LASTA LOCATION IN RAM. IF THE COMPARISON FAILS, THEN THE EEPROM IS NOT
F028: ; DONE YET, ADN THE TIMER IS RESET TO TIME 1/2 MSEC(OR 512 USEC). THE
F028: ; ROUTINE IS THEN EXITED.
F028: ;*****
F028: CKEEP LDAA LASTA ;GET THE LAST DATA WRITTEN
F028: FE 0104 LDX TEMP ;GET THE ADDRESS FOR THE BYTE IN EEPROM
F02E: A1 00 CMPA 0x ;COMPARE TO SEE IF THE WRITE IS COMPLETE

```

PAGE - 2 DATA\_COD  
File: :DATA\_CODE.TEXT

CODE FOR DATA POLLING IN INTERRUPT ENVIRONMENT, 6800 VERSION

```

F030: 26 ** BNE REINIT ;IF NOT EQUAL REINITIALIZE THE TIMER
F032: 86 00 LDAA #00 ;SET THE READY FLAG
F034: E7 0107 STAA READY ;AND STORE IT IN READY
F037: 20 ** BRA RET ;AND RETURN FROM SUBROUTINE
F039: 86 02 REINIT LDAA #02H ;LOAD THE FIRST BYTE FOR COUNTER
F03E: E7 0100 STAA TIMER ;WRITE TO TIMER DATA REGISTER
F03E: 86 00 LDAA #00H ;LOAD THE SECOND BYTE
F040: E7 0101 STAB TIMER+1 ;WRITE TO LSB OF TIMER DATA REGISTER
F043: 3E RET RTI ;RETURN FROM INTERRUPT
F044: ;*****
F044: .END

```

SYMBOLTABLE DUMP

CODE FOR DATA POLLING IN INTERRUPT ENVIRONMENT, 6800 VERSION

AB - Absolute	LB - Label	UD - Undefined	MC - Macro
RF - Ref	DF - Def	PR - Proc	FC - Func
PB - Public	PV - Private	CS - Consts	RS - Residents

```

CKEEP LB F028: CONFIG AB 0108: CTIMER
LASTA AB 0103: READY AB 0107: REINIT
WEEPROM LB F000: WRITE LB F00E:

```

```

AB 0102: DATA_COD PR ----: ERROR AB 0106: EXIT LB F027
LB F039: RET LB F043: TEMP AB 0104: TIMER AB 0100

```

Figure 2: Software Implementation for 6800 Microprocessor and a Simple Timer



## NOTES

## E<sup>2</sup>PROM PROVIDES THE SOLUTION TO FIELD ALTERABLE SOFTWARE

By Rick Orlando

The advent of the 5-volt E<sup>2</sup>PROM has brought about many changes in the manner in which the designer views his software. Such devices allow for in-field reprogrammability, which greatly reduces the cost and impact of software changes or upgrades. The 5 volt E<sup>2</sup>PROM allows the designer the capability to completely upgrade or change his software from a remote location rather than through the replacement of the system ROMs or EPROMs, a costly and inconvenient method at best. Complete in-field reprogrammability requires that the entire program store of the system be implemented in E<sup>2</sup>PROM. An alternative is a "hybrid" system.

A "hybrid" approach refers to a design which utilizes both EPROMs or ROMs in conjunction with E<sup>2</sup>PROMs to yield a design which features the best of both approaches: the low cost of a full ROM implementation, while maintaining the flexibility of a full E<sup>2</sup>PROM approach.

The secret to this approach is to analyze the software requirements of the end system from two distinct levels. That of the machine code routines which perform the simple tasks, and that of the higher level routines which call the lower level routines to perform an algorithm. The order in which the low level routines are called is determined by the higher level routines or program flow. This "Top-Down" programming approach is more efficient and structured, and is the basis for many high level languages. The fact that it can be used in machine language coding should not come as a surprise to designers, since the decomposition of a complex task into many simple tasks is quickly learned in programming, even if it is not called "structured programming" per se. The decomposition of the end task can sometimes lead to many different levels of program structure, but for the simplicity of discussion, this brief will limit itself to the most simple approach, that of two level program structure.

The lower level code consists of the machine

dependent routines such as that required to fetch a character from an I/O link. The buffering of multiple characters from this link might also be a low level routine. The interpretation of the buffered character string will be implemented in the higher level code, since it simply calls the lower level routines and determines the action to take based upon their results.

A basic example is that of the executing of multiple character command entered by the operator from a keyboard. The lowest level routine simply gets a character from the keyboard if a key is depressed. The next level of the software "buffers" the input to make the system more "user-friendly". This routine looks at the input string, eliminates misplaced blanks or other characters, and forms a character string which the high level program can understand. As a result, the "parsing" task is broken into three distinct levels.

The first involves the inputting of a single character from the keyboard into a character buffer. The second level continually calls the first routine until an end-of-input character is detected (such as a Carriage Return). The top most level of the code takes the parsed command and determines if it is a valid command by searching a table of valid commands. If the command is valid, the address of the routine to execute is fetched out of the table, and the processor performs a jump. Most of the input processing is handled at the lowest level, thereby reducing the overhead in the outermost routine.

As more and more of the processing tasks are pushed "down" into low level routines, the main procedure in the high-level segment becomes very short and simple. In fact, it can be reduced to a simple list of jump-to-subroutine instructions. This structured approach not only eases the software development task, but it also minimizes the debugging time required for the software since it is built upon other routines which have already been debugged.

If one completely decomposes the task to be performed by a particular segment of the systems main program, it becomes a list of procedure calls to lower level segments. This method lends itself very well to a system which can use E<sup>2</sup>PROM. Since the "outermost" program store is quite compact, it can be implemented in E<sup>2</sup>PROM while the majority of the machine code in the lower levels can be implemented in ROM or EPROM. Changes to the software then become as simple as changing the jump location in the E<sup>2</sup>PROM, and the order of execution of the lower level routines can be altered in such a manner.

Using this method, one can also reserve a section of the E<sup>2</sup>PROM for low-level "patch" alterations to the software. If a low level routine is found to be in error or needs updating, the new version of the machine code is loaded into the reserved section of the E<sup>2</sup>PROM. The jump instructions in the high level code in the E<sup>2</sup>PROM are simply changed to "jumps" to the new routine now residing in the E<sup>2</sup>PROM as opposed to the old routine in the ROM or EPROM. Figure 1 shows a typical memory map where the E<sup>2</sup>PROM is used to store the high-level routines which perform a variety of jump to subroutines to control the program flow. The low level machine language routines are stored in the EPROM as shown. Figure 2 shows how a patch is made to

replace the old routine in EPROM called "PARSE" with a new version loaded into the E<sup>2</sup>PROM. The jump-to-subroutine addresses in the E<sup>2</sup>PROM are updated to point to the new routine in E<sup>2</sup>PROM. The actual update or "patch" can be performed remotely, thereby eliminating the need for in field EPROM replacements for both the remedying of software bugs as well as the upgrading of systems in the field to take advantage of new features or capabilities.

Since both the valid character and the valid command tables reside in the E<sup>2</sup>PROM, new entries can be made to allow for additional command selection. New command character strings are simply added to the valid command list. The low-level code for the new command can either be loaded into the E<sup>2</sup>PROM patch area or utilize routines which already exist in the ROM or EPROM. The appropriate address is appended to the new command string.

If an error is discovered in an existing command, the valid command list is updated to point to the new command routine which is loaded into the patch area of the E<sup>2</sup>PROM. Figure 3 depicts the memory map after such a change has been made.

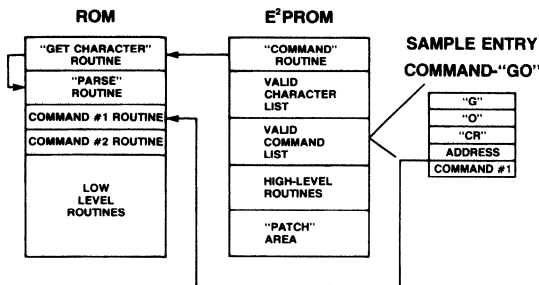


Figure 1: Memory Map Original Configuration

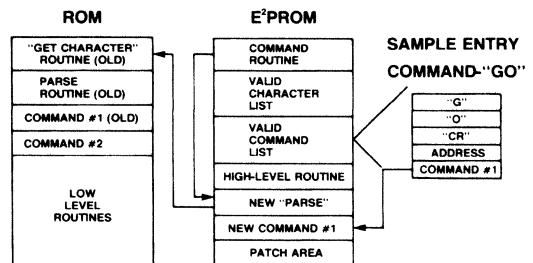


Figure 3: Memory Map After New Command Patch

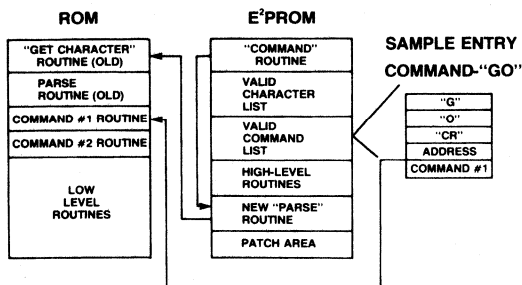


Figure 2: Memory Map After Routine Patch

Ultimate flexibility can be attained through a complete E<sup>2</sup>PROM design. It can also be shown that a minimal amount of E<sup>2</sup>PROM can add great flexibility to the system not only in terms of software alteration, but also in its intrinsic ability to store user alterable parameters such as configuration data. The actual ratio of EPROM to E<sup>2</sup>PROM must be determined based upon the systems' requirements. The advantage of the "hybrid" approach is that it requires that only the "top level" portion of the code be resident in E<sup>2</sup>PROM, and as such is usually limited to a series of procedure calls, which are very code efficient.

In the cases where the software is to be updated remotely, perhaps through the use of a modem, certain factors must be considered. The key point is that while the processor is executing programs in the E<sup>2</sup>PROM, it is inadvisable to write into that particular device. The reason for this is that while the device is performing the write cycle, any reads, such as an opcode fetch, will result in a high impedance bus.

The important issue is that the download of the new code must not reside in the E<sup>2</sup>PROM to be modified.

This can be accomplished in two different ways. The first implements the download program segment in the low level ROM or EPROM. In this case, the actual instructions will be present from the memory throughout the download sequence. Figure 4 shows such an approach where the download software is kept in the ROM. This routine writes the new bytes into the E<sup>2</sup>PROM and then enters a software loop to time out the E<sup>2</sup>PROM write cycle.

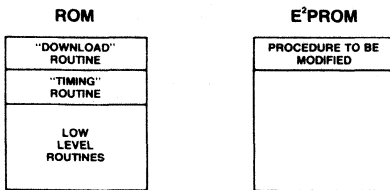


Figure 4: Memory Map-Download and Timing Resident in ROM

In some applications, this method may not be adequate, especially if the actual download routine is to be modified. In these cases, this program segment must be stored in the E<sup>2</sup>PROM, and hence, cannot be directly executed from the E<sup>2</sup>PROM to be modified. In this situation, a possible approach is to copy the download program segment from the E<sup>2</sup>PROM into RAM. The program then jumps to the RAM location, where the copy of the old code resides. This RAM routine loads the new program segment into the proper E<sup>2</sup>PROM locations, timing out the necessary E<sup>2</sup>PROM write cycle. Once the download is complete, the program executing out of the RAM then jumps back to the main program, and the download routine section of the E<sup>2</sup>PROM will contain the new code. Figure 5 shows the various stages of this operation in terms of the contents of the various memories and the program execution flow.

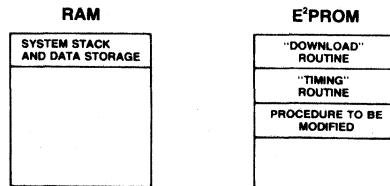


Figure 5a: Memory Map Prior to Download

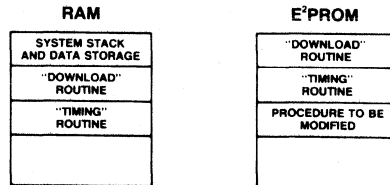


Figure 5b: Memory Map Download Routine Transferred to RAM

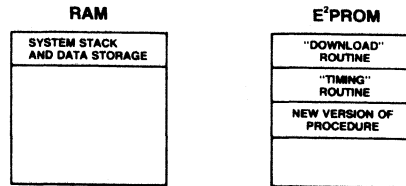


Figure 5c: Memory Map RAM Erased After Transfer Complete

As one can see, the "hybrid" approach to software design, utilizing a combination of both E<sup>2</sup>PROMs and ROMs or EPROMs, can result in a system which exhibits the advantages of the field alterability of E<sup>2</sup>PROMs. As the cost of the development and maintenance of the system software becomes more dominant in the overall cost of the system, such methods as those presented in this brief will become more commonplace in system design.

0008-3

## NOTES

# XICOR E<sup>2</sup>PROMs VS BATTERY BACKED-UP CMOS RAMs NONVOLATILE MEMORY SYSTEMS

By Applications Staff

## Introduction

System designers are increasingly facing the requirements of providing for nonvolatile memory in the system design. This nonvolatile memory may be required for program control, data acquisition, system configuration, or a host of other uses. Once the requirement for nonvolatile memory is established, the next hurdle faced by the system designer is the choice of the technology to be used to implement the nonvolatile memory. This means the system designers are faced with many tradeoffs when selecting a technology to implement the memory portion of their design. Tradeoffs between technologies such as bipolar, NMOS, CMOS, bubble, etc. depend in large part on overall system factors—such as requirements for density, cost, power-dissipation, availability, reliability, etc. Such tradeoffs are generally evaluated in the “time-constrained” design environment leaving little time for the system designer to complete a thorough investigation of the tradeoffs and their impact on the system design and reliability. The implementation of nonvolatile memory systems using battery backed-up CMOS RAMs has raised questions regarding the comparison of these technologies with E<sup>2</sup>PROM devices. The purpose of this Application Brief is to discuss the tradeoffs between implementing nonvolatile memory designs with E<sup>2</sup>PROM devices and/or the twin technologies of batteries and CMOS static RAMs.

## E<sup>2</sup>PROM/Battery Back-up CMOS Technology Comparison

CMOS static RAMs used in conjunction with batteries to achieve nonvolatile memory have the following characteristics in comparison with E<sup>2</sup>PROMs:

- 1.) Microprocessor compatible write cycle times
- 2.) Unlimited write cycles
- 3.) Low standby power
- 4.) Unknown battery/RAM data retention characteristics
- 5.) Temperature limitations

System reliability considerations and battery/CMOS design interface are the major issues

between implementing nonvolatile memory systems with CMOS/battery combination and E<sup>2</sup>PROM devices. E<sup>2</sup>PROM devices are specified to reliably operate over a wide range of operating temperatures, altitudes, pressures and moisture. In addition, E<sup>2</sup>PROM devices can be subjected to extreme temperatures (>300°C) to accelerate data retention failure mechanisms and determine the probability of retaining data at the lower operating temperatures. Although CMOS devices can be subjected to the same tests—the CMOS/battery combination cannot. The result is the CMOS/battery combination cannot be evaluated *TOGETHER* to determine the failure rates for data retention.

## Reliability

When choosing a memory device or technology, reliability factors should be carefully considered. Factors such as the environment in which it will be used, data retention time, etc. should all be considered.

In a forgiving environment (such as room temperature, low humidity and pressure) battery backed-up CMOS RAM has a respectable data retention time (although still not statistically measurable). Outside this environment, the performance of this combination decays rapidly. Most solid state memory devices (including CMOS RAMs and E<sup>2</sup>PROMs) have the capability of operating easily over the temperature range of -55°C to +125°C. But combined with a battery, a CMOS device can only operate within the temperature constraints of the additional technology—the battery. Most popular external on-board batteries spec a maximum operating temperature of 70°C. Xicor E<sup>2</sup>PROM devices guarantee a minimum retention time of 10 years at the worst case operating temperature (e.g. from -55°C to +125°C). Some CMOS RAM/battery combinations (contained in the same package) specify the “Expected Data Retention Time” of 10 years at 25°C. *This ten year data retention time is measured from the date of manufacture of the combination*

7

technologies. Non-operating specifications such as storage temperatures, also become a consideration. Battery backed-up RAM technologies (with the battery integral to the device) cannot be put into storage without the batteries. Since the batteries supply power to the RAM when  $V_{CC}$  is not present, there is no true storage mode (i.e. non-operating mode). This limits the storage temperature to the operating temperature specification of the combination. By comparison,  $E^2$ PROMs have specified storage temperature ranges from  $-65^{\circ}\text{C}$  to  $+165^{\circ}\text{C}$ . These storage temperatures apply whether the device is in the system or on the shelf.

## Types of Battery Backed CMOS

There are two basic types of battery backed-up CMOS RAM technology implementations available on the market today:

- 1.) Battery internal to the IC package
- 2.) Battery external to the IC package

In the first type, the battery is permanently attached to the device inside the IC package. This type of implementation has its advantages when board space is at a premium. *It is noted, however, that this type of device is non-standard in height (approximately 300 mils taller than conventional DIP packages) which limits or eliminates the possibility of automated device insertion.* The battery internal to the device is generally of primary type in that it cannot be recharged. The second type of CMOS RAM system implementation requires an external battery to provide the required standby power for nonvolatile data retention. For this type of implementation, additional circuitry is required for the detection of a power failure and interconnection between the "normal" power supply and the battery—thereby significantly increasing board space requirements.

## Battery Characteristics

Lithium and Nickel-Cadmium (Nicaid) are two of the most commonly used batteries for back-up with CMOS RAM. Each has unique advantages in the

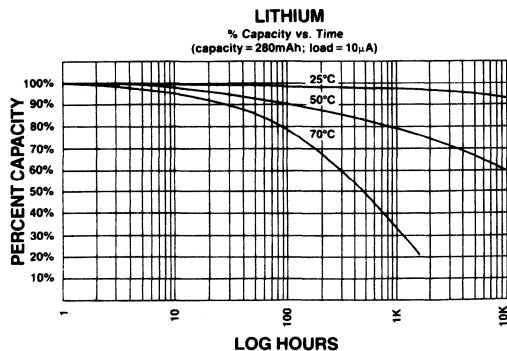


Figure 1: Lithium-Capacity vs. Time with Varying Temperatures

system environment. Both can handle temperature variations of approximately  $70^{\circ}\text{C}$  over "some" time duration. Negative current spikes of greater than  $10\mu\text{A}$  in the system can damage the device.

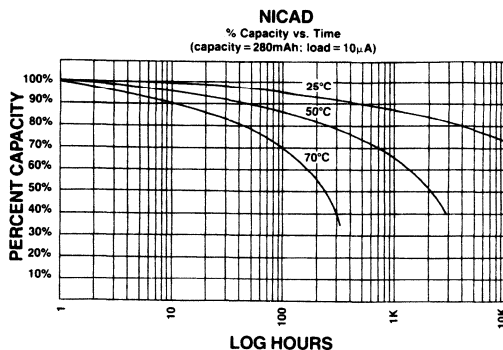


Figure 2: Nicaid-Capacity vs. Time with Varying Temperatures

Lithium batteries, although not rechargeable, have a greater life expectancy than Nicaid batteries and generally have a shelf life of 10 years at room temperature. When used in a system as a battery back-up, where temperatures vary, the output of the battery becomes sporadic. This causes a decrease in capacity and unstable circuit voltages. Figure 1 shows a typical characteristic curve of a lithium battery's capacity vs. temperature. Drawing a current of only  $10\mu\text{A}$ , the capacity could easily be reached in a very short time.

Additional concerns should be noted with transportation and disposal of lithium batteries. Because of the toxicity of lithium, the Department of Transportation regulates their transportation. Lithium cells containing greater than 0.5g must carry warning labels, and be transported by approved land, sea or air methods (document # DOT-E-7052). Generally, lithium batteries with more than 0.5g are restricted from passenger aircraft. Also the EPA requires special disposal of lithium batteries to secured landfill areas.

Nickel-Cadmium's most advantageous feature is the ability to recharge the battery once its output becomes low. Nicaids can generally be charged many times without damage. Nicaids tend to have a short shelf life so recharging is necessary. Figure 2 is a characteristic curve of a Nicaid battery's capacity when being operated over various temperatures with a current draw of  $10\mu\text{A}$ . When comparing Figure 1 and Figure 2 it is obvious that a Nicaid doesn't have the capacity of a lithium battery.

## Memory Densities

Xicor's NMOS floating gate technology has one transistor per storage cell. CMOS devices have four or six transistors per storage cell. This means that



the potential memory density of the E<sup>2</sup>PROM device is greater than for the comparable CMOS device.

## Physical Dimensions

The size and number of devices on a board have often times been a determining factor in designing circuitry. Xicor has numerous possibilities in minimizing the necessary circuitry. First, within the same package constraints the memory density of E<sup>2</sup>PROMs that are available is eight times greater than that of CMOS static RAMs. Besides the typical dual-in line-package (DIP), Xicor also offers LCC packaging. Users have also used the E<sup>2</sup>PROM in its die form for various applications, including the use of X2864A for core memory in military applications. This conserves enormous amounts of space (i.e. the X2864A die is 0.215in by 0.170in, and the X2816A die is 0.185in by 0.151in. in die form). When physical size is an important factor, E<sup>2</sup>PROM devices have a clear cut advantage.

## Applications

There are various optimum uses of E<sup>2</sup>PROMs for data and information storage. One such use is in the application of a portable data base where a large amount of memory is stored into a portable module. The memory module is plugged into the computer, data transferred bi-directionally, and then removed. The portable module can be transported or stored for long periods of time without the requirements of additional power. If battery backed CMOS were used in such an application, battery capacity could be a limiting factor for reliably maintaining data integrity.

In applications where data retention is critical, such as the boot-up storage area in a computer system, true nonvolatile memory is a must. With E<sup>2</sup>PROMs the data is nonvolatile, and allows any necessary changes to the boot-up routine. If batteries and CMOS RAM are used, critical "start-up" routines can be lost when the battery is replaced.

There are many other applications where E<sup>2</sup>PROMs are the technology of choice. These applications generally are exposed to harsh environments such as temperatures, changing pressure and altitude, or in high humidity environments.

The following is a partial list of typical applications which are ideal for E<sup>2</sup>PROM devices:

- System Parameter Set-up
- Configuration Data
- Calibration Data
- Constants Storage
- Industrial and Process Controllers
- Traffic Control Equipment
- High Altitude Meterological Data Storage
- Telemetry
- Satellite Communication Equipment
- Navigational Reference System
- Digital Positioning Machinery

- Measuring Instruments
- Temperature Monitoring Equipment
- Field Data Acquisition
- Electronic Musical Instruments
- Radio and TV Program Control
- Disc Drive Servo
- Robotics
- Depth Recorders
- Oil Field Drilling Systems
- Core Memory for Military Use
- Single Chip Microcontroller Applications

## Cost and Availability

Design costs with CMOS RAM are another consideration. The added time to design low power detection and switching circuitry adds to engineering costs. The added circuitry increases component and stocking costs and increases board test time.

Xicor E<sup>2</sup>PROMs enable the designer to minimize the cost of designing, the cost of components and the cost of "time-to-market." By minimizing or eliminating the additional circuitry required for data retention integrity, system cost and reliability are enhanced. Xicor is the leading manufacturer of E<sup>2</sup>PROMs, having sold more 5-volt only E<sup>2</sup>PROM devices (NOVRAMs & E<sup>2</sup>PROMs) than all other manufacturers combined. This experience allows Xicor to maintain leadership in this key emerging market segment by providing reliable cost-effective nonvolatile devices. This "learning curve" characteristic is shown in Figure 4. This figure shows the price curve as a function of time for the X2864A, an 8K x 8 E<sup>2</sup>PROM.

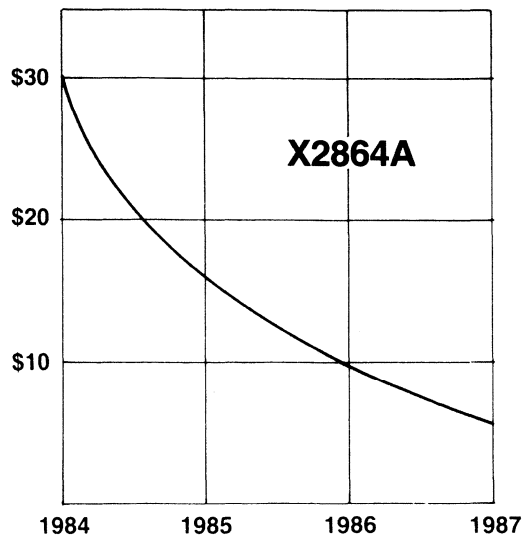


Figure 3: Price Curve as a Function of Time for the X2864A

7

## NOTES

## E<sup>2</sup>PROMs: THE COMPETITIVE EDGE AGAINST BUBBLE MEMORIES

By Richard Palm

E<sup>2</sup>PROM densities have increased to the point where they are now highly competitive with bubble memories. They also provide a number of distinct advantages over bubble memory technologies.

Bubble memories are primarily used as mass data storage devices in environments where tape or rotating memories cannot perform as reliably. These applications are predominantly in the industrial environment. The key factors for memory selection in these environments are high density and package hermeticity.

Assuming the packaging techniques for both bubble memories and E<sup>2</sup>PROM provide the same degree of hermeticity, let's examine the two side by side, specifically for industrial applications. For comparisons we'll use the Intel BPK 70A series of 1Mbit modules (each comprised of 7 devices), the Fujitsu 256K FBM43DA and FBC501 and Motorola MBM2011A.

### Design Complexity

As a designer and/or manufacturer I have a choice of designing my own memory module or purchasing one similar to the BPK 70A. If I chose to minimize cost I would design my own subsystem. However, I would then be faced with the task of interfacing the actual bubble memory device to the following minimum circuitry: coil predrivers; driver transistor arrays; a formatter sense amp; and a current pulse generator. Then to efficiently interface this array of devices to my micro, I would also require a VLSI bubble memory controller. Then the decision must be made as to whether the micro is to be tied down servicing interrupts from the controller or whether an additional VLSI DMA controller will have to be added to the system. This design task will cost engineering overhead, plus additional software to interface to the bubble memory controller. In addition, as a manufacturer I would also be faced with the task of testing a combination of analog and digital circuitry.

Interfacing the X2864A to a microcomputer or microprocessor requires no unique VLSI controllers or interface circuitry. It appears to be a ROM 90% of the time. When it requires modification, straight forward byte-wide writes directly on the bus are all that are required.

### Read Timing Comparison

Figure 1 is an illustration of comparative random read access times for the memory systems under comparison. The fastest bubble memory access time is 6.0ms for the FBM43. The Xicor X2864A-25 is 250ns or **TWENTY-FOUR THOUSAND TIMES FASTER** than the fastest bubble memory. Keep in mind, the read of the X2864A presented eight bits of data to the micro, it will take the FBM43 an additional 70μs to transfer the other seven bits.

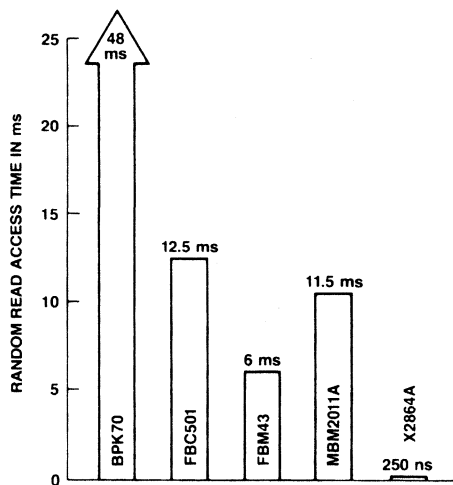


Figure 1: Random Read Access Times

## Write Timing

The fastest write time for the bubble memories being examined is 100KHz. These are serial devices, so that's one bit being written every  $10\mu\text{s}$ . Compared to an array of sixteen X2864A devices, employing DATA Polling, Page Writes and assuming the typical write cycle speed of 5ms the entire contents of the array can be written in 2.56 seconds compared to the 10.48 seconds for the BPK 70A and the 2.62 seconds for a single 256K FBM43DA. These last two figures *do not* include the latency time to locate the bit cell to begin the write.

In a very high density system requiring 8Mbits of memory, the BPK 70A modules can be wired in parallel eight wide, effectively providing an eight bit bus to the bubble memory controller. The write cycle time to write the entire memory remains at 10.48 seconds. The equivalent X2864A array would be comprised of 128 devices, 8 times the number required for the 1Mbit array, yet the write cycle time to change the entire array is only 3.15 seconds, STILL THREE TIMES FASTER THAN BUBBLE MEMORY.

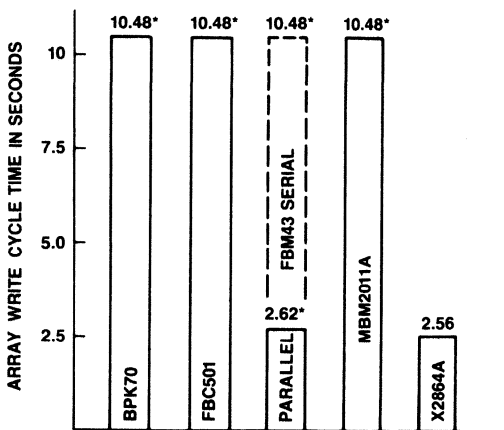


Figure 2: Array Write Cycle Times

\*Note: Rewrite time for FBM43 is 10.48 seconds when writing serially or 2.62 seconds when writing four bits in parallel.

## Power Consumption and Power Supplies

Another major concern for any design is power consumption and limiting the number of power supplies required in a system. The X2864A requires only

one +5 volt supply, whereas the BPK 70A requires +5 and +12, and the Fujitsu devices require +5, +12 and -15. Figure 3 illustrates power consumption for a 1Mbit design using various configurations of X2864s and bubble memories.

These are critical design considerations for industrial applications where the memories might be in remote locations such as, Digital Numeric Controlled equipment being operated by a master CPU.

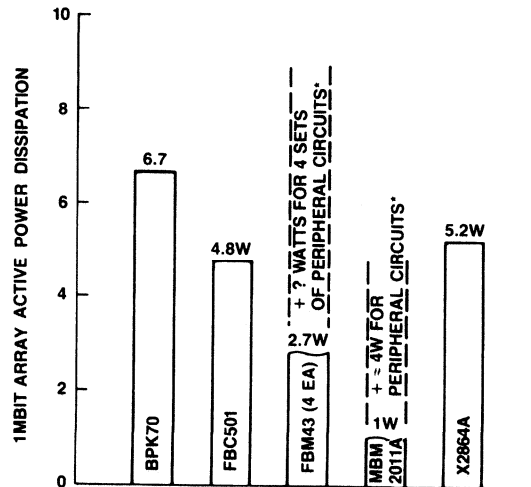


Figure 3: Comparison of Active Power Consumption For 1Mbit of Memory

\*Note: Power consumption for these arrays is calculated for the memories only. The required peripheral circuitry was not included in the calculations.

## Operating and Storage Temperatures

Figures 4 and 5 illustrate the comparative temperature ranges for which these devices are guaranteed. The X2864A is a hands down winner.

Nonvolatile storage temperature can be extremely important in data logging applications, where the data is collected at point "A" and then transported to point "B" for analysis. The use of X2864A devices allows transportation without the worry of possibly losing data.

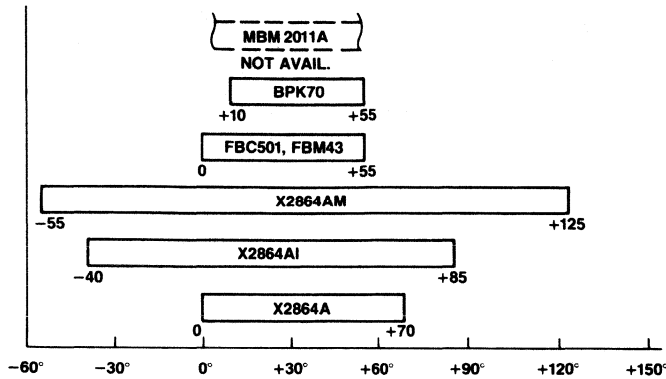


Figure 4: Operating Temperature Range

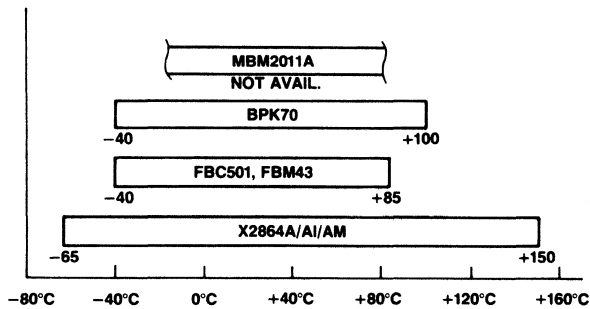


Figure 5: Nonvolatile Storage Temperature

## Packaging Density

An additional consideration in making the decision to use E<sup>2</sup>PROMs vs. bubble memories is the number of bits per square inch of board space. Bubble memories at first glance appear to have an advantage. 1Mbit can be in a package as small as 1.1 in. x 1.1 in. But this all requires peripheral circuitry around it so that it can be accessed. The added circuitry builds up to a board approximately 4 in. x 4 in. On the same size board sixteen X2864A devices

can easily be mounted. And using the soon to be available J-lead surface mount devices, both sides of the board can be used to double the density.

Added to this is the upward growth pattern that E<sup>2</sup>PROMs allow. In the second half of 1985 Xicor will be sampling the X28256. On the same 4 in. x 4 in. board a user can implement thirty-two devices using both sides of the board. These thirty-two devices will provide 8Mbits of memory.

## NOTES

## “t<sub>DV</sub>”—WHAT IS IT?

By Richard Palm

E<sup>2</sup>PROMs, RAMs and EPROMs all being memory devices have similar specifications. However, one of the specifications unique to E<sup>2</sup>PROMs is t<sub>DV</sub> (Data Valid Time).

The E<sup>2</sup>PROM requires a relatively lengthy period of time to tunnel charge onto or off of the floating gate to complete the write cycle. This time is specified as t<sub>WC</sub>. In order to more closely emulate RAM write timing, Xicor introduced “self timed” write operations. Xicor E<sup>2</sup>PROMs latch the address on the falling edge of  $\overline{WE}$  or  $\overline{CE}$ , whichever occurs last, and latch data on the rising edge of  $\overline{WE}$  or  $\overline{CE}$ , whichever occurs first. The falling edge of the write operation not only latches the address of the byte (or page) to be written but also starts a number of internal timers that control the programming cycle.

In page mode, subsequent  $\overline{WE}/\overline{CE}$  falling edges will restart the timers. But it is these timers that require specifying t<sub>DV</sub>.

In most microprocessor based systems, t<sub>DV</sub> can be ignored because t<sub>WP</sub> will be less than t<sub>DV</sub>. However, in applications employing slower microprocessors and microcontrollers t<sub>WP</sub> might be quite long. The actual internal programming cycle could begin before either  $\overline{CE}$  or  $\overline{WE}$  returned high, thereby missing valid data even though t<sub>DS</sub> was met.

Once the internal timers initiate the programming cycle, the I/Os will be disabled. Therefore, valid data must be present on the bus before the I/Os are disabled. As an example, refer to Figure 1 illustrating the sequence of events.

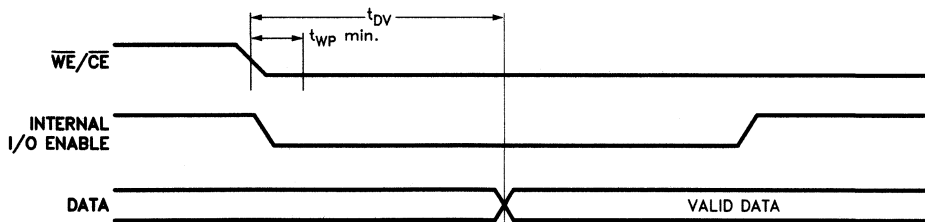
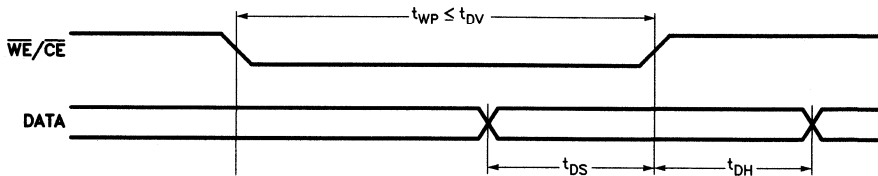


Figure 1: External/Internal Timing

0060-1

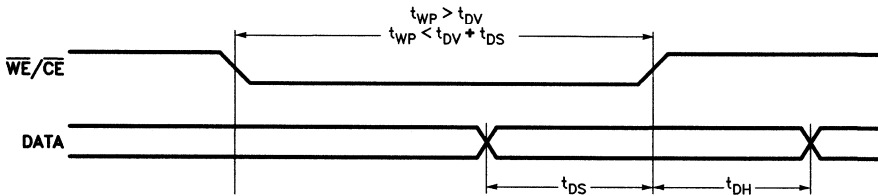
$t_{DV}$  is the maximum time to elapse from the falling edge of  $\overline{WE}$  or  $\overline{CE}$  (whichever occurs first) before valid data have to be presented to the E<sup>2</sup>PROM.

How does this impact your design? The following timing diagrams cover the three possibilities. Notice that in all the examples  $t_{DH}$  must still be met.



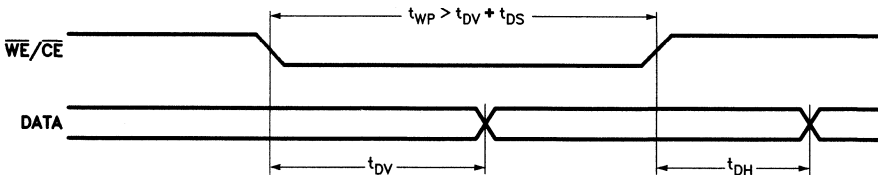
Example 1: If  $t_{WP}$  is equal to or greater than  $t_{WP}$  min but less than  $t_{DV}$ , then  $t_{DS}$  and  $t_{DH}$  must be met.

0060-2



Example 2: If  $t_{WP}$  is greater than  $t_{DV}$  but less than  $t_{DV}$  plus  $t_{DS}$ , then  $t_{DS}$  and  $t_{DH}$  must be met.

0060-3



Example 3: If  $t_{WP}$  is greater than  $t_{DV}$  plus  $t_{DS}$ , then  $t_{DV}$  and  $t_{DH}$  must be met.

0060-4

In summary, the data must be valid on the bus for the worst case timing parameters; whether that is  $t_{DV}$  or  $t_{DS}$  and always valid for  $t_{DH}$ .

## Glossary

$t_{DV}$	Data Valid Time
$t_{WC}$	Write Cycle Time
$t_{DS}$	Data Setup
$t_{WP}$	WE Pulse Width
$t_{DH}$	Data Hold



Reprinted from

A MCGRAW-HILL PUBLICATION

# Electronics®

---

## **5-volt-only EE-PROM mimics static-RAM timing**

By Applications Staff, Xicor Inc., Milpitas, CA

7

# 5-volt-only EE-PROM mimics static-RAM timing

On-chip charge pump, interface latches simplify designs; textured polysilicon enhances tunneling through thick oxides

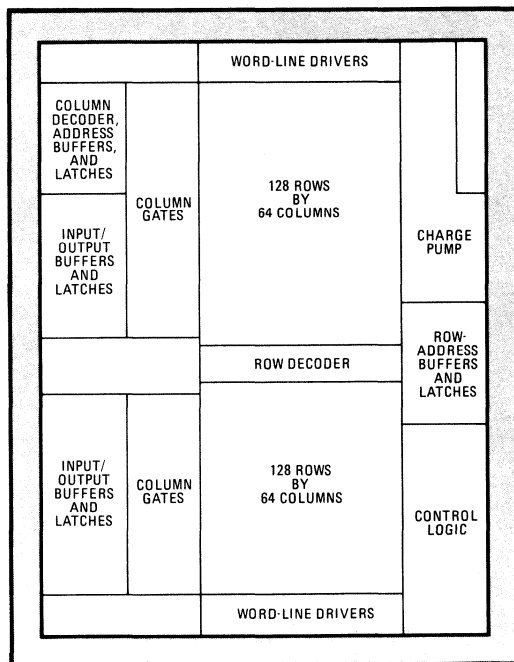
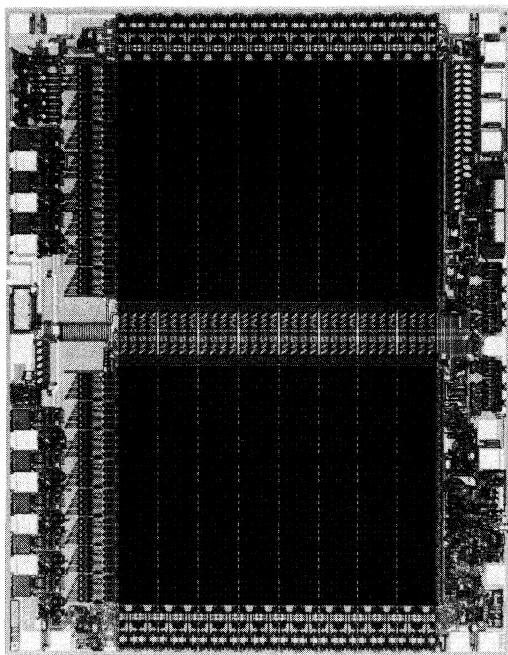
By Applications Staff, Xicor Inc., Milpitas, CA

□ The approaching mastery in fabricating electrically erasable programmable read-only memory conjures up dramatically different system designs. On the most mundane—but perhaps most immediately valuable—level, alterable nonvolatile semiconductor memory will soon banish routine service calls by allowing remote changing of system software. Not far away, if still somewhat tinged with the aura of science fiction, is the vision of self-programmable systems that adapt themselves to a changing operating environment. The catalyst for these advances is an EE-PROM that is simple to incorporate in microprocessor-based systems.

Now being launched by Xicor is a family of EE-PROMs that is the first to do away completely with external

supporting hardware (Fig. 1). The chips contain the charge pump that generates a high programming voltage from a 5-volt supply. Further, latches on chip hold the data, address, and control signals during alteration of the cells, which typically takes 5 milliseconds per byte and is timed internally. The part marks the debut of an EE-PROM that can simply be dropped into a standard 24-pin static random-access-memory socket.

The 5-micrometer n-channel MOS technology applied to produce the X2816A 2-K-by-8-bit EE-PROM and the X2804A, a 512-by-8-bit version, is the same as that being used to build the devices in the Novram line of static RAMs with nonvolatile backup arrays [*Electronics*, Oct. 11, 1979, p. 111]. Recently, however, theoretical



**1. All aboard.** This 16-K electrically erasable programmable read-only memory integrates all its support circuits. A charge pump generates the programming voltage from a 5-V supply; latches hold addresses and data during the internally timed write cycle.

## Shedding light on electron tunneling

The present generation of electrically erasable programmable read-only memories using floating-gate structures draws on a reservoir of process development, circuit design, and basic physics. The floating-gate process has been in production for many years and forms the building block of EE-PROMs. The next step toward a practical 5-volt programmable EE-PROM centers on removing the high currents typically used to alter data by avalanche or hot-electron injection. A high voltage can be generated on chip as long as only minute currents are required, as with the new circuit designs.

As far as the underlying physics, the tunneling processes found in most floating-gate EE-PROM devices are described by a theory introduced in the 1920s by Fowler and Nordheim. As shown in the theory, if the emitting surface is flat, very thin oxides of around 100 angstroms are necessary for significant tunneling currents at reasonable voltages of 15 to 20 volts. To the continued puzzlement of researchers, experimental data has fit the theory roughly, but not especially closely.

Xicor purposely fabricates textured emitting surfaces that are covered with low-lying bumps or hills formed during the oxidation of the polysilicon surface. Recently, tunneling theory has been extended to describe this textured-surface geometry with the result that conventional devices are now better understood as well.

The low-lying hills, which serve as the electron emitters, are less than 150 Å high and more than 500 Å across their base. The figure on the right shows the triple-polysilicon tunneling structure in cross section, a scanning-electron-microscope photograph of a typical textured tunneling surface, and the geometry of a typical bump on the polysilicon surface.

Because the oxidation is a well-controlled step, the properties of the emitters are exceptionally regular. The

shape of the emitters tends to increase the electric field at the crest of the hills, enhancing the emission of electrons substantially, which allows the use of thick oxide layers of approximately 800 Å. As indicated in the figure, increasing the voltage not only increases the emission, but enlarges the area from which it occurs. This effect explains the discrepancies between experiments and the earlier tunneling theory. The thick oxides have important practical advantages: they are easier to manufacture and lead to increased retention of data.

Until recently, the theoretical work on Fowler-Nordheim tunneling had solved only the limited case of perfectly flat plates. Roger Ellis and H. A. R. Wegener of Xicor recently presented measurements and calculations that agree over a range of eight orders of magnitude in the current. With the aid of the methods of differential geometry, the tunneling characteristics of a textured surface were calculated for the first time. As the scale of the texturing is reduced, the solution naturally reduces to the familiar flat-plate case. The figure on the far right compares the tunneling currents for flat and textured surfaces.

The two structures were designed for the same operating point—a current density of  $10^{-4}$  amperes per square centimeter at 17 V. At low fields, such as are applied to read data, the thick oxide used with the textured surface has only about a thousandth the current of a flat surface. As a result, data retention would be expected to be far longer.

The current from a flat emitter in fact can be modeled much more closely by considering some texturing of its surface. Even single-crystal polished silicon wafers have surface features on the order of 5 Å, and normally processed polysilicon has even larger variations. Thus, Xicor's tunneling structures accentuate features that are always present in floating-gate devices.

work has significantly added to the understanding of the tunneling of electrons from textured polysilicon, the mechanism exploited in all these products (see "Shedding light on electron tunneling," above).

This work explains how a textured surface emits more electrons than a smooth one for a given voltage and oxide thickness. (Scanning-electron-microscope studies of the polysilicon surface show that the texturing consists of low-lying bumps about 150 angstroms high and 500 Å across.) This enhanced emission allows the use of typically 800-Å-thick oxides, instead of very thin, 100-Å layers that are much harder to produce reliably.

Besides being easier to manufacture, thicker oxides lead to increased retention of data. What's more, a 16-K EE-PROM with 5- $\mu$ m linewidths and 800-Å-thick oxides promises to be more readily scaled down for denser memory arrays than one with, for example, 3- $\mu$ m lines and 100-Å-thick oxides.

Floating-gate technology along with the architectural features making the parts simple to use present the state of the art in EE-PROMs after a decade of development. Metal-nitride-oxide-semiconductor structures yielded the first nonvolatile memories that were electronically alterable. These devices store data by trapping electrons within the nitride and oxide dielectrics. Besides the prob-

lems these devices encounter—data disturbance during the read operation and the loss of data over time—they require multiple power supplies, one of which is often negative, and signal swings beyond TTL levels. All this complicates their incorporation within microprocessor-based systems that work with a single 5-v power supply and TTL levels.

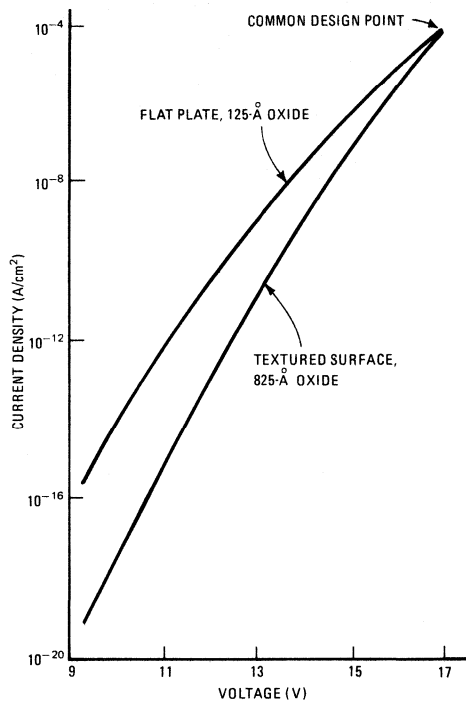
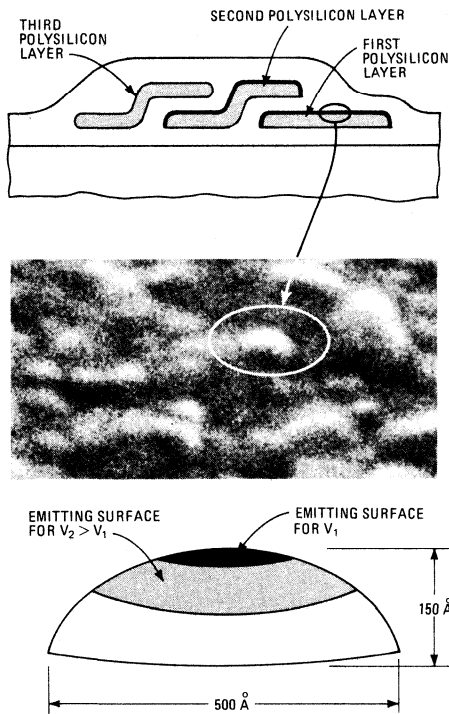
Further complicating their use is the fact that the addresses and data must be stable for the entire write cycle, lasting up to 40 ms. It takes extra hardware to capture these signals and to time the write interval in order to free the processor for other tasks.

### Comparing EE-PROMs

The second generation in EE-PROMs was ushered in by the 2816 from Intel Corp. of Santa Clara, Calif. This part stores data by trapping charge on floating polysilicon gates, as is done in ultraviolet-light-erasable PROMs, or E-PROMs, and improves the data integrity compared with MNOS parts. Although the 2816 has a standard pin configuration and uses TTL signal levels, it still requires an externally generated high-voltage pulse for altering data, not to mention latches for holding the address and data signals.

Measured against the 2816, recently introduced third-

7



generation parts incorporate some or all of the required supporting hardware on chip (see table). The 2817 from Intel moves the external high-voltage pulse generator onto the chip, so that a fixed 21-v supply is all the user must provide. Though it does include the necessary interface latches, it still requires an external capacitor to

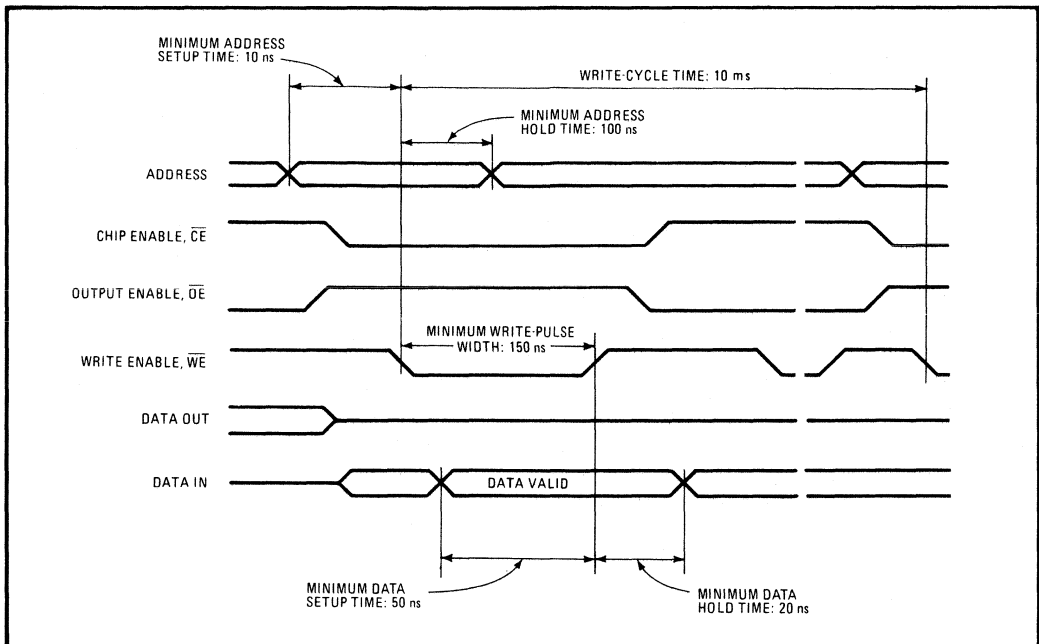
time the write cycle. More recently, the 5213 from Seeq Technology Inc., San Jose, Calif., operates from a single 5-v power supply, but still needs latches and external timing. Only the X2816A completely eliminates the external components.

All the X2816A's input and output signals are TTL-compatible and the addresses and data are latched so that they need be stable for only 200 nanoseconds to initiate the 10-ms write cycle. Once the write cycle starts, the part self-times the remainder of the operation, freeing the microprocessor and the data bus for other tasks. Freedom from an external timing capacitor or other hardware leads to considerable savings in component and assembly expense as well as in board space. In addition, the cost of design is lower because the part is far simpler to operate.

As can be seen in Fig. 2, the timing of a write cycle for the X2816A is as simple as that for a static RAM. The latches are active only during a write cycle, when they hold the addresses and data to allow the microprocessor to use the bus for other tasks. A write cycle is activated by both chip-enable and write-enable lines going low while output-enable is high. The addresses are latched on the last low-going edge of either the chip-enable or write-enable signal. The data inputs are latched by the

COMPARISON OF RECENT ELECTRICALLY ERASABLE PROGRAMMABLE READ-ONLY MEMORIES

Part	Intel 2816	Intel 2817	Seeq 5213	Xicor X2816A
On-chip charge pump				
Address and data latches				
Automatic erase				
Internal timing of write cycle				
Internal control of write-pulse shape		needs external capacitor		
Maximum erase-write cycle time (ms)	20	75	20	10



**2. Like a static RAM.** The write-cycle timing for the X2816A EE-PROM looks much like that for a static random-access memory. Although the write cycle takes a maximum of 10 ms, latches hold the address and data signals, freeing the processor for other tasks.

first of those two signals to return to the high level.

Unlike with most EE-PROMs, there is no need to precondition the data at the desired address before the write cycle, for the X2816A automatically performs an erase function immediately after the cycle starts. Both the erase and write of the data occur during the 10-ms write cycle. The condition requiring the output-enable signal to be high to initiate the write cycle ensures that the part will not be mistakenly programmed when the power is switched on or off.

### A compatible part

Conveniently, a socket designed for one of the earlier EE-PROMs can accept an X2816A as well. An internal detector on the write-enable pin senses a signal above 12 V and initiates the internal write cycle (and thus the part may second-source the 2816). This high-voltage signal is used only to detect the system's request to write data—otherwise, the part draws virtually no current from the high-voltage supply.

Further, because of their internal control over the write cycle, the Xicor EE-PROMs can plug into the standard sockets of 2-K-by-8-bit static RAMs. They will operate with the signals normally applied to a RAM, with the only restriction being the delay of 10 ms after starting a write cycle before accessing data. As mentioned already, the X2816A is not on the bus and requires no servicing or supervision during this 10-ms wait. Since the parts time their own write cycle, other EE-PROMs may be updated while a write cycle is continuing on the first unit.

The 10 ms quoted is the maximum delay for writing—the typical delay is only half that. By polling the part during its write cycle, a user can usually reduce the waiting time. One method is to place a particular byte of data at some address and then ask for data from that address during the write cycle. If the data that is retrieved checks against the data written, the part has finished its cycle.

With the cost of a single service call to modify a system in the field mounting toward \$200, no doubt the system that can be serviced from afar will be an early development goal. With an EE-PROM plus a modem or other communication method, a telephone call suffices to download the program and configuration data pertaining to all or some of the systems tied together in a network.

A prime application for this technique would be a system of point-of-sale terminals for a market chain. Pricing for items could be dumped to all terminals in the system by calling each store and modifying the price look-up table in each terminal. Similarly, gasoline prices at computer-controlled service-station pumps may be remotely updated.

Indeed, from here it is only a simple step to imagine writing programs that learn as they go. A terminal might analyze the way it was being used and adjust itself for optimum performance in a particular application. By the same token, the next wave of automated manufacturing systems may calibrate themselves, hold information about the steps that have been completed, then interrogate themselves to determine their point in the manufacturing process. □

## Publisher's letter

---

**T**hough nonvolatile semiconductor memories have been commercially available for a decade or so, the early versions were no joy to work with—multiple power supplies, high voltages, and slow writing discouraged potential users. The push to create a simpler part is yielding noteworthy results, particularly the 16-K electrically erasable programmable read-only memory that Xicor Inc. describes on page 2.

Solid state editor Rod Beresford first heard about the company's new chip back in January. "At the time," he recalls, "we had just published our annual markets forecast, in which we were projecting that consumption of EE-PROMs would nearly quadruple by 1985, to over \$330 million. Many of those parts will be going into microprocessor-based systems, where 5-volt power supplies and TTL signal levels are the only way of life."

Xicor's X2816A gets high marks for ease of use. In fact, it's not only microprocessor-compatible, it's a truly self-supporting EE-PROM that's as simple to use as a static random-access memory. Beyond those features, though, our editor was struck by the research at Xicor on the electron tunneling that provides the storage mechanism in EE-PROMs. "I studied tunneling in school," notes Rod, "and can appreciate what the Xicor researchers were up against in trying to get a better fit between theory and experiments. I think they succeed admirably."





---

# Understand your application in choosing NOVRAM, EEPROM

Richard Orlando, Xicor Inc., Milpitas, CA

*As appeared in EDN Magazine*

*May 12, 1983*

# Understand your application in choosing NOVRAM, EEPROM

*Examining how NOVRAMs and EEPROMs serve various applications illustrates the memory devices' capabilities and simplifies device selection.*

**Richard Orlando**, Xicor Inc

If your system design calls for electrically erasable nonvolatile data storage, you can simplify the selection of semiconductor memory for that task by choosing from among four basic types—NOVRAM, EEPROM, EAROM and battery-backed CMOS RAM. Assuming that you've examined the system-level tradeoffs among these memory types (EDN, April 14, pg 135) and have narrowed your choice to the first two, use the information presented here to understand the detailed tradeoffs and design considerations underlying NOVRAM and EEPROM use. In some application classes, either memory type functions adequately; in others, you have a clearcut choice. And in still others, consider taking advantage of both—an approach that often results in cost reductions and enhanced features.

## NOVRAMs use multiple technologies

First, however, understand how each memory type works. Nonvolatile static RAM (NOVRAM) combines two memory technologies on one monolithic chip. In Fig 1, the NOVRAM shown contains 1k bits of static RAM and 1k bits of electrically erasable PROM (EEPROM). The device comprises cells that in turn each contain one cell of each memory type, rather than housing two separate memory arrays (see box, "Anatomy of a NOVRAM cell").

In this NOVRAM, data gets read and written exactly as in a standard static RAM. In addition, the  $\overline{\text{Store}}$  signal transfers each RAM cell's data into a shadowing EEPROM cell; EEPROM-stored data gets reloaded into the RAM via the  $\overline{\text{Recall}}$  signal. Note that the EEPROM-cell portion is accessible only through the RAM portion.

One of this device type's most powerful features is its ability to transfer the entire RAM contents into

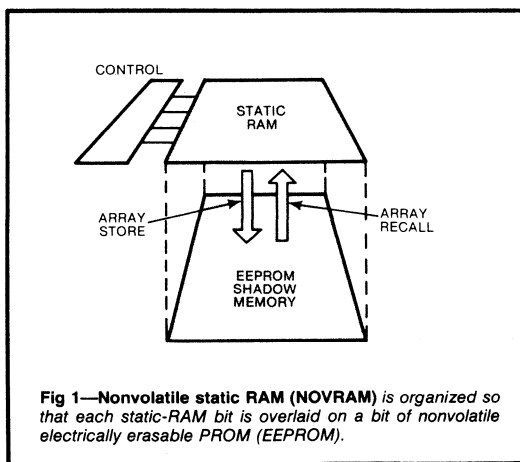
nonvolatile storage in one operation, initiated by bringing the TTL-compatible  $\overline{\text{Store}}$  LOW. The operation takes less than 10 msec, and once data is stored in this manner, only another store operation can alter it—even if the chip loses power.

Generating  $\overline{\text{Store}}$  in the event of a power failure therefore saves the RAM contents, subject only to power remaining on the chip for the next 10 msec. RAM data can also be changed without disturbing the shadowing EEPROM, allowing the system to manipulate two separate groups of data.

## EEPROMs offer greater density, fewer features

EEPROM, your other major memory choice, resembles UV-erasable EPROM. Unlike EPROM, however, it can be written electrically in circuit; it needs no prior erasure by exposure to ultraviolet radiation.

First-generation EEPROMs are merely electrically



**Fig 1—Nonvolatile static RAM (NOVRAM) is organized so that each static-RAM bit is overlaid on a bit of nonvolatile electrically erasable PROM (EEPROM).**



## Careful analysis simplifies the EEPROM vs NOVRAM choice

alterable ROMs (EAROMs). They're reprogrammable only after an entire memory array (or at least one page) is electrically erased. Similarly, second-generation devices require erasure of individual bytes before programming. Third-generation EEPROMs, however, automatically and internally erase a to-be-written byte as part of the write cycle; they also contain much of the required voltage-generating and pulse-shaping functions on chip.

Two examples of third-generation EEPROMs currently in production are the Intel 2817 and the Seeq 5213. The 2817 latches the data to be written and eliminates the need for prewrite erasure. However, it requires an external high-voltage supply as well as a timing capacitor for deriving internal timing signals.

TABLE 1—EEPROM/NOVRAM COMPARISONS

	NOVRAM (X2212)	EEPROM (X2816A)
Density (bits)	1024	16,384
Price (1k level)	\$9.00	\$23.00
Cost/bit	\$0.0088	\$0.0014

The 5213 generates the high voltage on chip but requires external latches that hold the data and address valid during erase and write operations.

Fourth-generation EEPROMs are characterized by

### Anatomy of a NOVRAM cell

NOVRAM-cell operation depends on a phenomenon termed Fowler-Nordheim tunneling. In the NOVRAM, a layer of oxide isolates a gate from an underlying section of polysilicon. Applying a large positive voltage to this floating gate while holding the underlying polysilicon near ground programs the gate.

Specifically, electrons attracted to the floating gate's significantly higher potential tunnel across the separating oxide. As a result, the floating gate acquires a net negative charge from the tunneled electrons.

The cell is erased in a similar manner: The floating gate is held at a low potential while the potential of the top polysilicon layer is raised; the electrons then tunnel across the oxide from the floating gate to the neighboring polysilicon sandwich.

The EEPROM technology employed in Xicor's NOVRAM uses a 3-layer polysilicon sandwich that, when coupled with a 6-transistor static-RAM cell, results in the NOVRAM circuit shown in Fig A. The state of the static-RAM cell determines whether the EEPROM

cell is programmed or erased during a store cycle.

Capacitance ratios are the key to the data transfer from RAM to EEPROM. If node  $N_1$  is LOW,  $Q_7$  is turned off, allowing the junction between capacitors  $C_3$  and  $C_4$  to

float. Because the combined capacitance of  $C_3$  and  $C_4$  is larger than  $C_P$ , the floating gate follows the Store-node voltage. When the voltage on the floating gate is sufficiently high, electrons tunnel from  $POLY_1$  to  $POLY_2$ , and the

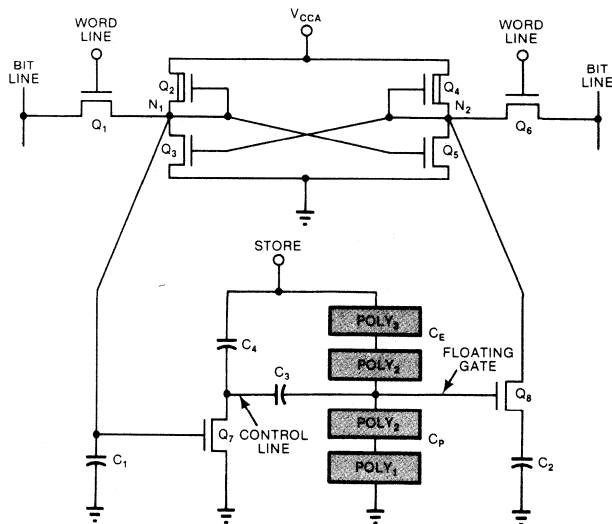


Fig A—A NOVRAM cell consists of two sections: a 6-transistor RAM and a shadowing 2-transistor EEPROM.

on-chip generation of all high-voltage and wave-shaping functions in addition to their use of on-chip latches and self-timing features. Their byte-write requirements are identical to those of static RAM except that the EEPROM write cycle, once initiated by normal static-RAM timings, takes as long as 10 msec. Once a byte-write operation begins, the EEPROM is self supporting, freeing the processor and all external circuitry for other tasks. Read timing to the EEPROM is identical to that of a standard EPROM, RAM or ROM.

An important feature of a fourth-generation EEPROM is its compatibility with currently used RAM, EPROM and ROM. An EPROM- or ROM-based system needs only an additional Write Enable line to

each socket to provide retrofitting for EEPROM. This control line allows the changing of data tables and program store without removing the component from the system, as required with EPROMs.

### Choosing between NOVRAM and EEPROMs

Many application requirements can be satisfied by either of the two memory types. However, note that although NOVRAM is the most versatile in terms of features and capabilities, the price you pay for its greater intelligence is increased cell size.

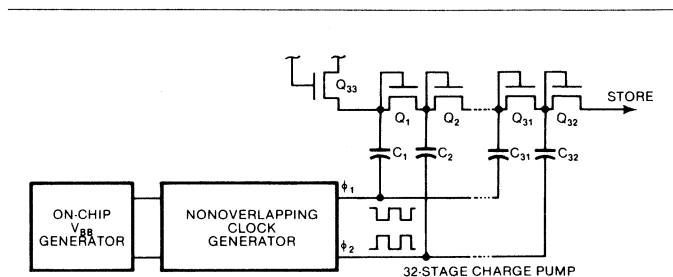
Specifically, a fourth-generation EEPROM's cell is small and simple, allowing much higher density storage than in a NOVRAM. The EEPROM is also more efficient as memory-array area increases, thanks to the

gate becomes negatively charged.

If node  $N_1$  is HIGH,  $Q_7$  turns on, grounding the junction between  $C_3$  and  $C_4$ .  $C_3$ , larger than  $C_E$ , holds the floating gate near ground when the Store node gets pulled HIGH. This action creates a sufficiently large field between  $POLY_2$  and  $POLY_3$  to tunnel electrons away from the floating gate, leaving it with a positive charge.

The recall operation also depends on capacitance ratios.  $C_2$  is larger than  $C_1$ . When the cell receives the external Recall command, the internal power supply ( $V_{CCA}$ ) first goes LOW to equalize the voltages on  $N_1$  and  $N_2$ . When  $V_{CCA}$  is allowed to rise, the node with the lighter capacitive load rises more rapidly. The flip flop's gain causes the lightly loaded node to latch HIGH and the opposite side to latch LOW. If the floating gate has a positive charge,  $C_2$  is connected to  $N_2$  through  $Q_6$ , and  $N_2$  latches LOW. If the floating gate has a negative charge,  $Q_6$  gets turned off and  $N_1$  experiences the heavier loading.

A major task in the development of the NOVRAM was to reduce the



**Fig B—A 32-stage charge pump** internally generates a NOVRAM's high Store voltage, allowing the device's NOVRAM and EEPROM sections to operate from 5V.

amplitude and simplify the waveform of external voltages needed for programming or erasure. Earlier devices required carefully shaped pulses with amplitudes exceeding 20V.

The first step in the cell design was to reduce the internal voltage level presented to the cell to initiate electron tunneling. The voltage magnitude required for programming a floating gate is related to the intensity of the electric field generated at the oxide-polysilicon interface by that voltage.

Electric-field strength at the oxide-polysilicon interface can be

increased by using an extremely thin oxide, on the order of 100Å. A second technique uses textured polysilicon to locally enhance the field at the surface and achieve Fowler-Nordheim tunneling. It achieves better data retention.

Once the internal voltage-level requirement was reduced, a key achievement in device design was the on-chip generation of the high-voltage pulses needed to program or erase an individual cell. A Store-voltage generator (**Fig B**) provides the solution; it uses a 32-stage capacitor/transistor charge pump.

## Each NOVRAM cell combines RAM and EEPROM

**TABLE 2—EEPROM/NOVRAM DATA-CAPTURE SPEEDS**

	NOVRAM (X2212)	EEPROM (X2816A)
Byte-Write Time	256 × 1 μsec	256 × 10 msec
Store Time	10 msec	0
Total Time	10.26 msec	2.56 sec

decrease in the relative proportion of support-circuitry area required. Therefore, EEPROMs are more likely to be the device of choice if your application needs large amounts of memory.

The larger cell size and more extensive on-chip support that gives NOVRAM its added capabilities also results in a higher cost per bit, which might not be justified in applications that don't require all of a NOVRAM's features. Consider, for example, the cost-per-bit comparison between the X2212 256×4-bit NOVRAM and the X2816A 2k×8-bit EEPROM (Table 1): NOVRAM cost per bit is more than six times greater than that of EEPROM.

However, cost-per-bit ratios can be deceiving for systems requiring a minimum amount of nonvolatile memory. Lower density nonvolatile memories often are more cost effective in a NOVRAM configuration. The smallest NOVRAM currently available, the 64×4 X2210, is also the least expensive 5V device.

Another selection factor to consider is the required write time. An EEPROM requires a relatively long write time (10 msec/byte max), while NOVRAM write

time is that of a typical static RAM. Therefore, NOVRAMs are more suited for applications requiring frequent memory-data changes, while EEPROMs most suit applications calling for infrequent memory writes.

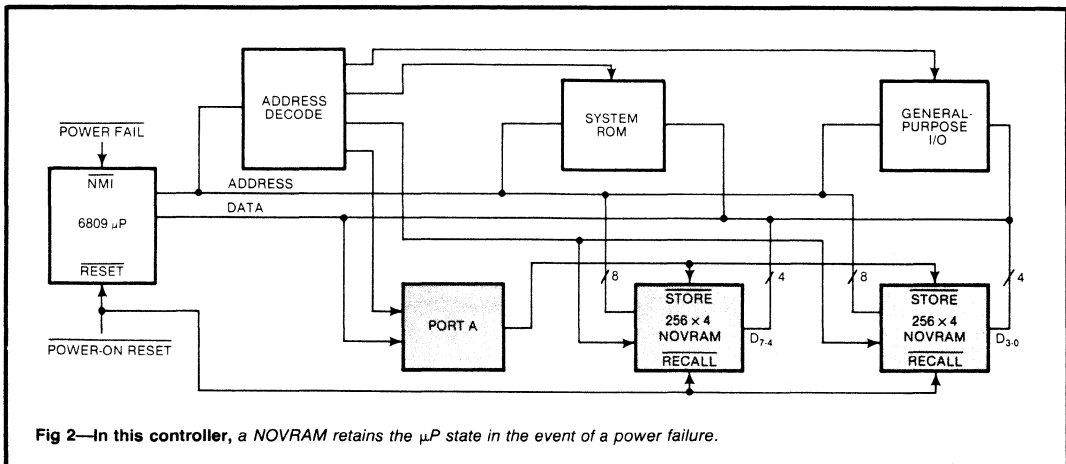
A NOVRAM is also better suited to data-capture applications. Table 2 compares two 256×4-bit NOVRAMs organized in a byte-wide configuration with a 2k×8 EEPROM in terms of the time needed to store 256 bytes of information. These times assume a 1-μsec/byte max processor write-cycle time. You can see that the NOVRAM's single-store operation makes it much faster. A NOVRAM system can update and store 10,000 bytes of data in the time needed to store two bytes of EEPROM information.

Another important NOVRAM feature is the device's ability to initiate and complete a nonvolatile store of data under external-signal control. This feature can be a key decision criterion in real-time applications such as power-fail re-entrant systems.

### Both types serve power-fail-tolerant controllers

As noted, however, many applications can profitably use either device type. One common application in this class centers on retaining important system information in the event of a power loss. In most systems, power failures require reinitialization of the entire system, necessitating the temporary loss of system operation. In real-time control applications, this loss of control can cause expensive and sometimes dangerous failures of the process or equipment being controlled.

Such an application's main requirement is therefore some type of nonvolatile storage upon power failure. A prime consideration in this type of environment is the storage of a fixed amount of data upon receipt of an



**Fig 2—In this controller, a NOVRAM retains the μP state in the event of a power failure.**

```

;*****
; AN EXAMPLE OF THE POWER-DOWN AND POWER-ON CODE FOR THE 6809 USING
; THE NOVRAM FOR PROCESSOR STATUS STORAGE.
;*****
; LOCATION DEFINITIONS
NOVRAMLO .EQU 0000H
NOVRAMHI .EQU NOVRAMLO + 256.
; THE NOVRAM IS LOCATED AT THE BOTTOM OF THE 6809 MEMORY MAP
DIRTY .EQU NOVRAMHI ;TEST BYTE FOR POWER FAIL CONDITION
OLDSTK .EQU NOVRAMHI-6 ;STACK POINTER NONVOLATILE LOCATION
STACK .EQU NOVRAMHI-7 ;PROCESSOR STACK BEGINNING LOCATION
TEMP1 .EQU NOVRAMHI-1 ;IMPORTANT PROCESS PARAMETERS
TEMP2 .EQU NOVRAMHI-2
TEMP3 .EQU NOVRAMHI-3
PORTA .EQU 0000H ;LOCATION OF DATA REGISTER FOR PORT
.ORG 0F000H
;*****
; POWER FAILURE ROUTINE
;*****
PFAIL STS OLDSTK ;WRITE CURRENT STACK POINTER INTO NOVRAM
; AT THIS POINT, THE POWER FAIL INTERRUPT HAS PUSHED ALL OF THE
; CURRENT VALUES OF THE PROCESSOR REGISTERS ONTO THE STACK. THE
; STACK POINTER POINTS TO THESE VALUES.
LDA #0ASH ;LOAD ACCUMULATOR WITH POWER FAIL FLAG
STA DIRTY ;STORE FLAG IN NOVRAM
LDA #00. ;WRITING A 0 TO THE PORT GENERATES
STA PORTA ;A STORE SIGNAL TO THE NOVRAM
LOOP BRA LOOP ;SIT AND WAIT UNTIL POWER DISAPPEARS
;*****
; POWER-ON RESET ROUTINE
;*****
RESET LDA #0FFH ;SET ALL OUTPUTS TO A "1"
STA PORTA ;WRITE TO PORT TO KEEP STORE HIGH
LDA DIRTY ;LOAD FLAG TO SEE IF POWER FAILED
CMPA #0ASH ;IT WILL BE A 0ASH IF IT DID
SNE INIT ;IF NOT DO NORMAL INITIALIZATION
LDA #00H ;CLEAR THE POWER FAILURE FLAG
STA DIRTY ;IN THE NOVRAM
LDA #00H ;AND GIVE A STORE SIGNAL
STA PORTA ;TO STORE THE NEW FLAG
LDA #0FFH ;RESET PORT.
LDS OLDSTK ;LOAD OLD STACK VALUES
RTI ;RETURN FROM POWER FAIL INTERRUPT
INIT ;NORMAL INITIALIZATION CODE
;
;
;
.ORG 0F00H
.WORD PFAIL ;POWER FAILURE INTERRUPT VECTOR
.WORD RESET ;POWER-ON RESET INTERRUPT VECTOR
.END

```

Fig 3—A power-failure-tolerant controller's 6809- $\mu$ P assembly-language routines handle both failure store and recovery. NOVRAM handles the stack and other temporary storage.

## NOVRAM doubles as bootstrap and global memory

external Power Fail signal. You can use an EEPROM for this purpose if the processor has sufficient time to recognize the power failure and respond by writing the data into memory. Otherwise, a NOVRAM is the device of choice because it captures data in one nonvolatile store operation.

Fig 2 shows a simple controller that uses a NOVRAM to retain the state of a  $\mu\text{P}$  in the event of a power failure. The Power Fail signal generates a  $\mu\text{P}$  interrupt, and the NOVRAM stores the contents of all RAM including the  $\mu\text{P}$  stack.

Upon interrupt acknowledgement, the  $\mu\text{P}$  registers are pushed onto the stack as program control branches to the interrupt routine (Fig 3). The routine writes the current stack pointer and a test byte to the NOVRAM, signifying that a power failure has occurred, and then generates a Store signal. The power supply is designed to ensure that the  $V_C$  level remains above 4.5V for 10 msec after it generates the Power Fail signal.

Once power is restored, the Power-On Reset signal generates a Recall signal to the NOVRAM. The power-on routine in the  $\mu\text{P}$  checks the state of the test byte to see if a process was interrupted by a power failure. If so, the stack pointer gets loaded with the address of the saved processor state, a return from interrupt is executed, and the process resumes.

### NOVRAM stores terminal configurations

An application in which NOVRAM is the device of choice lies in the storage of terminal-configuration information, consisting of such parameters as baud rate, data format and parity method. The conventional

approach to this task (Fig 4) stores data in DIP switches on a pc board somewhere in the terminal; the user must have a terminal manual handy for decoding switch settings to change any of the preset features.

One alternative uses menu-driven configuration modes to set the terminal and a NOVRAM to store the terminal-configuration parameters. The user can easily change the configuration information for specific tasks and retain this data until the terminal loses power.

Upon power-up, a set of predefined default parameters stored in the NOVRAM's EEPROM section goes to RAM, and the terminal is configured. The NOVRAM also allows the user to change default parameters for subsequent sessions by transferring the modified RAM data to EEPROM—in either a general or privileged user environment. The NOVRAM's ability to manipulate two sets of data proves important here because the terminal software operates on the data in the NOVRAM's RAM section, regardless of whether the terminal is in the default configuration or a user-entered one.

In Fig 4's conventional approach, an 8-section DIP switch holds the configuration information. If a switch position is open, the pull-up resistor causes a ONE to appear at the buffer input; a closed switch denotes a ZERO. Decoding the buffer's address and reading the data provides the switch information. If the system needs more than eight bits, the design requires additional switches, resistors, buffers and logic.

If a block of memory addresses is reserved for configuration information, the granularity of the address decoding increases with the number of DIP

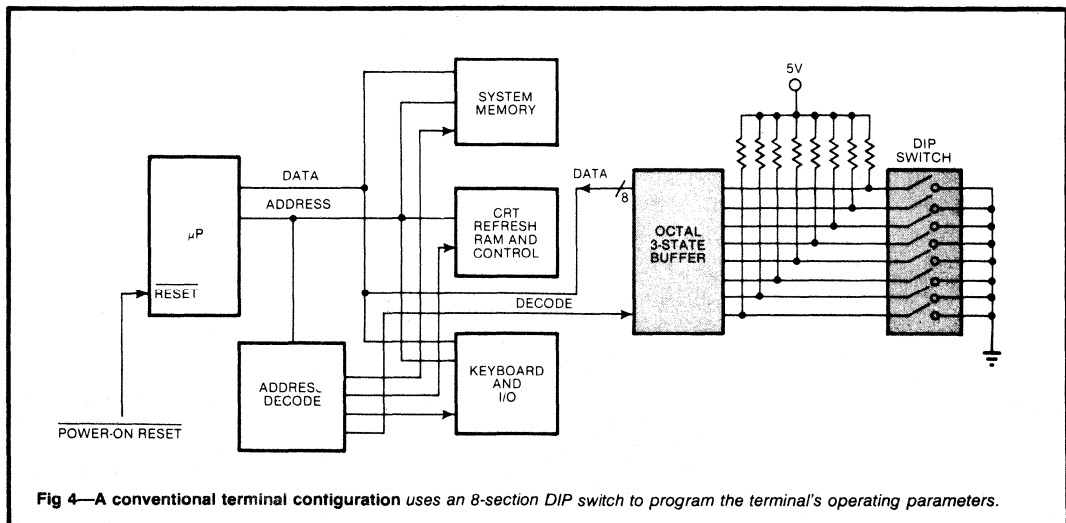


Fig 4—A conventional terminal configuration uses an 8-section DIP switch to program the terminal's operating parameters.

## In-system data modifications make EEPROMs more versatile than EPROMs

switches required. And you can change the default data only by altering individual switch positions.

The NOVRAM implementation of this system (Fig 5) permits the storage of 1k bits of configuration information in one 18-pin X2212. If you reserve an 8k memory-address block for configuration storage, the NOVRAM requires only a single chip-select decode. The only restriction in this arrangement is that four parameter bits get read simultaneously, rather than eight. Note that storing the same amount of information using the conventional approach calls for 128 DIP switches and octal buffers, 1024 resistors and sufficient address decoding to provide 128 separate locations within the 8k field—an address granularity of 64.

A terminal user employs the keyboard to enter operational parameters into the NOVRAM. The user enters a configuration mode when the terminal is in the off-line or local mode. A menu display shows the current terminal configuration; the user moves the cursor and/or strikes a control key to alter the current values. Once the configuration is established, the user exits the configuration mode, and the terminal operates according to the new parameters. The user can also change the default parameters by entering a control signal that places the new configuration mode in the NOVRAM's EEPROM section.

In this application, very few terminals would ever require the NOVRAM's full storage capacity for

configuration information. You could therefore employ the unused portion to store other operational and maintenance parameters.

### NOVRAM loader provides reusable memory

A system that employs a bootstrap loader during initialization is another prime NOVRAM application candidate. Examples of such applications include single-chip  $\mu$ Cs operating in external-memory modes and full-blown systems requiring the maximum allowable memory space. A common approach to this requirement stores the bootstrap program in ROM or EPROM. However, the program occupies memory space that might be used for other purposes during system operation. Because most initialization routines use a relatively small amount of memory space, this approach can be particularly wasteful in space-limited systems.

As an alternative, you can preprogram the bootstrap into the EEPROM section of a NOVRAM. Upon reset, the system generates a Recall signal to the NOVRAM, loading the bootstrap into RAM. The bootstrap program executes, and the NOVRAM RAM section then becomes free for other uses. This design feature even allows bootstrap-program alteration via external control for servicing or software updates.

Fig 6 shows a simple disk-oriented system that uses NOVRAM as a bootstrap memory. After booting, the NOVRAM becomes a global RAM. The device—and

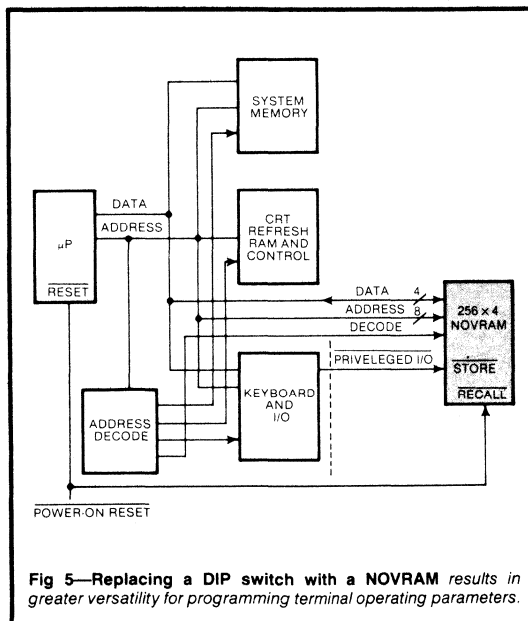


Fig 5—Replacing a DIP switch with a NOVRAM results in greater versatility for programming terminal operating parameters.

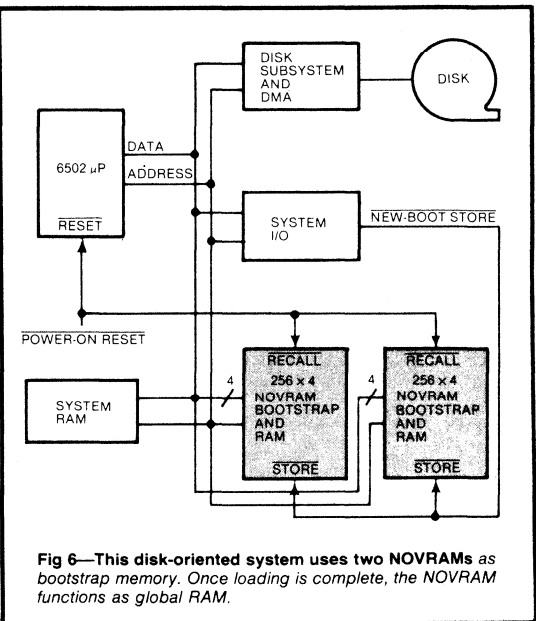


Fig 6—This disk-oriented system uses two NOVRAMs as bootstrap memory. Once loading is complete, the NOVRAM functions as global RAM.

```

;*****
; THIS PROGRAM SEGMENT DEMONSTRATES THE OPERATION OF A SYSTEM WHICH
; USES A BOOTSTRAP PROGRAM PRELOADED INTO THE NOVRAM'S EEPROM. UPON
; POWER-ON RESET, THIS BOOT IS RECALLED INTO THE EEPROM'S RAM. THE
; BOOTSTRAP PROGRAM CONFIGURES THE SYSTEM, AND THEN USES THE NOVRAM'S
; RAM AS REGULAR RAM. THE NOVRAM IS LOCATED AT THE BOTTOM OF THE
; 6502'S MEMORY MAP SO THAT THE HIGHEST LOCATIONS CAN CONTAIN THE
; PROCESSOR'S INTERRUPT VECTORS. ACTUAL LOADING OF THE OPERATING
; SYSTEM INTO MAIN MEMORY IS ACCOMPLISHED BY A DMA CONTROLLER, WHICH
; LOADS THE PROGRAM FROM THE DISK.
;*****
DMAData      .EQU    0C000H ;DMA DATA REGISTER
DMACTRL     .EQU    0C001H ;DMA CONTROL REGISTER
PROGRAM     .EQU    00200H ;START OF PROGRAM MEMORY

                .ORG    0FF00H

; THIS PROGRAM SECTION IS LOADED INTO THE EEPROM SECTION OF THE
; NOVRAM, AND IS RECALLED UPON POWER-UP.
BOOT          LDX    #0FFAH ;LOAD THE X INDEX REGISTER WITH FF
                TXS    ;TRANSFER TO STACK POINTER AT 01FF
CONFIGURE    ; THIS CODE SECTION CONFIGURES THE DMA CONTROLLER.
                ; AND SETS THE INITIAL LOAD LOCATION AT 0200H, SO
                ; THAT PROGRAM DATA WILL NOT OVERWRITE THE STACK.
SEEK         ; THIS CODE SECTION TELLS THE DMA CONTROLLER WHAT
                ; DISK SECTION IT SHOULD GET THE PROGRAM FROM, AS
                ; WELL AS HOW MUCH DATA TO LOAD.
GO           LDA    #01.    ; 01 IN THE DMA CONTROL REGISTER
                ; WILL INDICATE DISK DATA LOADING
                STA    DMAData ; STORE IN THE DMA CONTROL REGISTER
                LDA    #0ASH  ; WRITE TO TEST BYTE TO SIGNIFY BOOT
                STA    TEST   ; IF WE SEE A #0ASH, WE ARE IN BOOT
LOOP        JMP    LOOP    ; LOOP UNTIL DMA CONTROLLER INTERRUPTS
;*****
; NMI FROM DMA INTERRUPT WILL VECTOR HERE. THIS ROUTINE CHECKS THE
; STATUS FROM THE DISK SUBSYSTEM AND DMA CONTROLLER TO INSURE THAT
; THE REQUESTED DATA HAS BEEN LOADED. ONCE A SUCCESSFUL BOOT HAS
; TAKEN PLACE, THE SYSTEM CAN CHANGE THE NMI VECTOR SINCE THE NOVRAM
; NOW FUNCTIONS AS A REGULAR RAM.
;*****
INTERRUPT    LDA    DMACTRL ; CHECK TO SEE IF THE DESIRED PROGRAM
                ; HAS BEEN SUCCESSFULLY LOADED. IF SO,
                ; ALL WILL BE ZEROES EXCEPT D0 WHICH
                ; WILL BE SET TO SIGNIFY THAT AN
                ; INTERRUPT WAS GIVEN.
                CMP    #01   ; ARE WE LOADED?
                BNE    BOOT  ; IF NOT, WE HAVE AN ERROR. RE-BOOT.
                LDA    TEST  ; GET TEST BYTE TO SEE IF IN A BOOT.
                CMP    #0ASH ; IF SO, TEST BYTE WILL BE AS HEX.
                BEQ    PROGRAM ; AND JUMP TO PROGRAM BEGINNING.
ERROR       ;OTHERWISE WE HAVE AN ERROR.
TEST        .BYTE    00.    ; A ZERO IS STORED IN TEST INITIALLY.
                .ORG    0FFFAH
NMI         .WORD    INTERRUPT; NMI WILL GO TO SYSTEM START ROUTINE.
RESET      .WORD    BOOT    ; POWER-ON RESET WILL CAUSE AUTO BOOT.

```

Fig 7—A 6502- $\mu$ P assembly-language boot routine is located temporarily in NOVRAM, which forms the highest 256 bytes of memory in this system.

## Use EEPROM if data changes are byte size and infrequent

hence the bootstrap routine—is in the highest memory segment so it can hold all the interrupt vectors.  $\mu$ P's such as the 6502 and 6800 use these locations for reset and interrupt pointers.

In the bootstrap program (Fig 7), the reset vector for the 6502  $\mu$ P points to the boot routine. Fig 6's two NOVRAMs reside in the highest 256 bytes of the address map. Upon power-up, the NOVRAM's EEPROM section gets loaded into the device's RAM section. The  $\mu$ P then initializes the stack pointer, and the DMA controller begins a data transfer from the disk. A test byte gets set to show that a boot process is under way.

Once the DMA transfer begins, the  $\mu$ P loops until an interrupt signifies that the operation is complete. The  $\mu$ P vectors to the interrupt-handling routine, which determines if a valid DMA has occurred. If an error has occurred, the program causes a jump to location Program, where the first byte of the loaded program resides. The NOVRAM RAM is then free for general use. Note that you must take care not to accidentally overwrite the interrupt and reset vectors, located in the highest memory locations.

### EEPROM stores controller parameters

Turn now to some applications in which an EEPROM is the device of choice. One such task is the storage of coefficients in PID (proportional integral-differential) controllers.

Modern control applications such as the PID algorithm are characterized by two basic qualities. First, they are computationally intense. Second, their ability to precisely control a set condition is based on their knowledge of the effects of their outputs. This knowledge results from deriving the various controller coefficients via calculations: Each controller output must be calculated with reference to the previously defined term.

If a PID system loses power, it must resynthesize all data before it approaches the level of performance exhibited before the power loss. The data tables for each control task are fairly large and require a substantial amount of memory. Therefore, a controller might use EEPROM for algorithm-coefficient storage.

Note also that most PID-controller deviations result from the sensitivity of the system's sensors as well as the response time and accuracy of the control outputs. These variables might change in a particular unit but are usually the same when power returns to the controller; they need only be updated occasionally as the system runs. An EEPROM's slow write time and fast read time make it ideally suited for this infrequent-write application.

Finally, note that parameters stored in EEPROM are

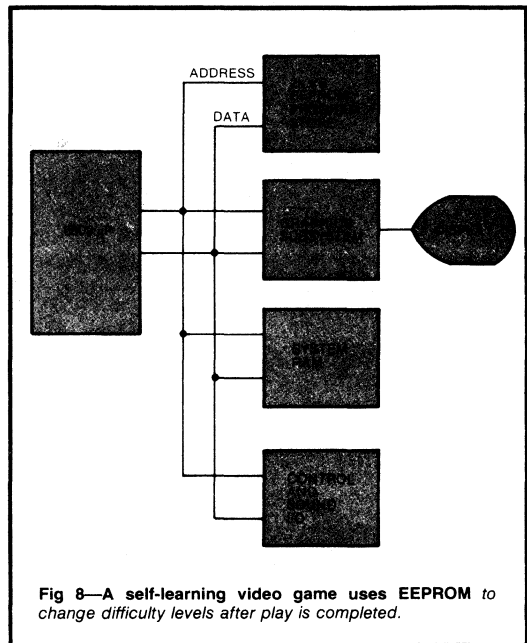


Fig 8—A self-learning video game uses EEPROM to change difficulty levels after play is completed.

available to the system whenever it's running—whether programmed into the system during initialization or resulting from previous system operation. An EEPROM implementation of such a system thus results in shorter system-interrupt recovery time as well as self-recalibration upon component replacement.

### Self-learning video games use EEPROMs

Another potential EEPROM application centers on the storage of self-teaching or self-modifying code, through which a process or algorithm can tailor itself based on the results of previous executions. Such applications are characterized by updates to program storage, which usually occur relatively infrequently. This high read-to-write ratio of memory access, as well as the densities required in the program store, generally dictate an EEPROM implementation.

An example of this application category is a self-learning video game (Fig 8). Such a game's success depends largely on its ability to keep a player interested by continually increasing the level of challenge after repeated plays.

At the end of a certain period (Fig 9), the game analyzes the scores and modifies its program (including timing loops and difficulty factors) to present a more complex play to the next group of players. The learning algorithm also makes the game easier to play under



certain conditions, preventing unwarranted increases in difficulty.

The initial game code includes several routines that

make the game progressively more difficult to play. These routines get bypassed in the initial program execution by always-executable branch instructions. At

```

;*****
; THIS IS AN EXAMPLE OF 6809 GAME CODE WITH BRANCH NEVERS
;*****
PLAY          ;THIS SECTION OF CODE IS THE EASIEST
;
;
SECT1         BRA     SECT2  ;WE START OUT BY BYPASSING THIS SECTION
;THIS SECTION OF CODE IS MORE DIFFICULT
SECT2         BRA     SECTN  ;WE ALSO BYPASS THIS SECTION
;
SECTN         BRA     ENPLAY ;WE HAVE N DIFFICULT ROUTINES
;
ENPLAY        LDA     TEST   ;CHECK THE END OF GAME FLAG
CMPA         #0FFH        ;IT WILL BE AN FF IF GAME IS OVER
BNE          PLAY         ;IF GAME NOT OVER, GO BACK TO MAIN LOOP
BRA          FINISH        ;IF IT IS, GO TO FINISH SECTION

FINISH        ;THIS IS THE AREA FOR THE END OF THE GAME CODE. IT MAY
;CALL PROCEDURES TO MAKE THE GAME HARDER IF THE
;ANALYSIS OF PAST SCORES WARRANTS.
;*****
; THIS SECTION OF CODE INCREASES THE DIFFICULTY LEVEL OF THE GAME BY
; REPLACING ONE OF THE BRANCHES AROUND THE MOST DIFFICULT ROUTINES
; WITH A DUMMY BRANCH OR BRANCH NEVER INSTRUCTION. THIS ROUTINE ALSO
; INCREASES A GLOBAL DIFFICULTY FACTOR, ON WHICH MANY OF THE GAME
; PLAYING ALGORITHMS ARE COMPUTED, BY ONE.
;*****
DIFFULT       .BYTE    00    ;DIFFICULTY FACTOR
;
; TABLE OF BRANCH LOCATIONS
TABLE         .WORD    SECT1
              .WORD    SECT2
;
;
;
TABLEND       .WORD    SECTN

MAKEHARD      LDX     #TABLE  ;START LOOKING THROUGH TABLE AT THE TOP
LOOK          CMPX    #TABLEND ;ARE WE AT THE END OF THE TABLE?
BEQ          NEXT         ;IF SO, GAME CAN'T BE MADE HARDER!
LDA          [X++]        ;LOOK AT THE OPCODE AT THE BRANCH, AND
;INCREMENT INDEX REGISTER FOR NEXT LOOK
;AUTO INCREMENT BY 2 INDEXED)
CMPA         #21H        ;CHECK TO SEE IF IT IS A BRANCH NEVER
BNE          LOOK         ;IF NOT, THEN CHECK THE NEXT ONE
STA          [0,X]        ;OTHERWISE MAKE THE GAME HARDER BY
;INCLUDING A ROUTINE BY STORING A BRANCH
;NEVER (INDEXED INDIRECT)
INC          DIFFULT      ;INCREMENT DIFFICULTY FACTOR

ATTRACT       ;ENTER THE ATTRACT MODE FOR THE GAME
;
;
NEXT          ;WE CAN'T MAKE THE GAME HARDER, SO WHAT DO WE DO??
              .END

```

Fig 9—Written in 6809- $\mu$ P assembly language, this self-learning video-game program changes branch instructions based on previously obtained scores.

## EEPROM and NOVRAM could team up in some cases

the end of each play, the system determines from the score whether to make the algorithm more difficult. If so, it eliminates some of the branches around difficult parts of the game software. A simple table stores all of these branches. Other features, including speed parameters and energy levels, can also be stored to make the game more difficult as scores improve. Storing them in EEPROM provides the additional advantage of easy updates and changes in the basic table.

### EEPROM and NOVRAM team up

As a final example, consider how you might combine EEPROM and NOVRAM in an automobile navigational system that could direct a driver to a location within a specific city or area. Proponents of this approach envision beacons located throughout an area, notifying each in-car computer of the car's current location. Provided with this information, a local electronic map and the desired destination, the computer would direct the driver along the most efficient route.

Data-storage requirements would be extensive, implying the use of EEPROM. After all, the system must not only be programmed with a map of the area roads but must also be able to select between many possible alternatives based upon continuously changing factors such as time of day and known construction areas. Using EEPROM would allow the car's driver to load the navigational computer upon entering a location such as a filling station.

A NOVRAM would also prove critical to this application. It would contain rapidly changing current information, which would get transferred to the NOVRAM's EEPROM section upon reaching a destination. The approach allows power removal from the system while the car is parked, eliminating battery

drain. Restarting the vehicle would transfer the current data from the NOVRAM's EEPROM section back to its RAM section.

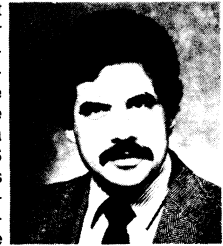
Fig 10 shows how the hardware could be implemented. Map information, stored in EEPROM, gets changed as necessary via the map-download controller, a serial interface over which the data is transmitted. The transmission rate is low because the map data is written into EEPROM, which specs a slow write cycle.

The system has two main interfaces—to the driver and to the vehicle. The former consists of a keyboard for input and a CRT for display of the map and other information. The latter receives data such as mileage and speed so that the system can monitor the driver's progress along a given route.

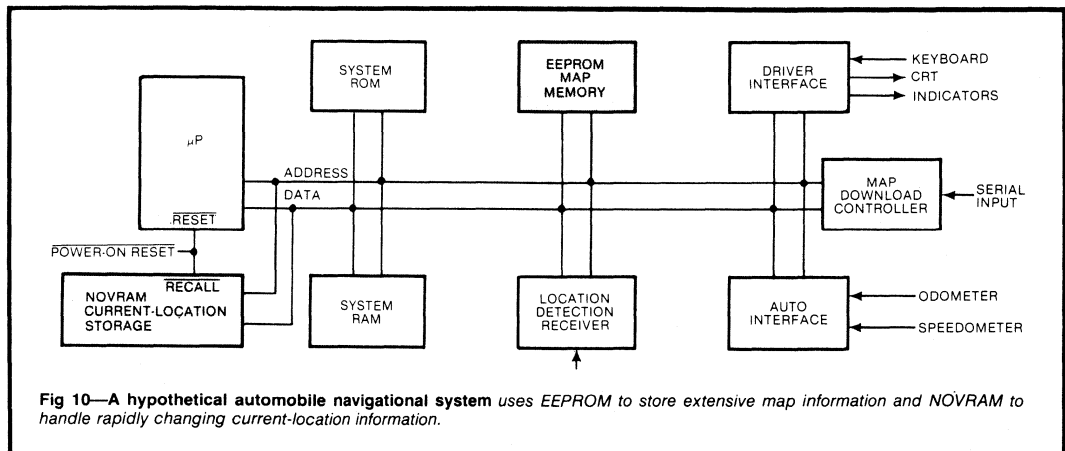
EDN

### Author's biography

**Richard Orlando** is product marketing manager at Xicor (Milpitas, CA), where his duties include product development. He is a member of the IEEE Computer Society, the ACM, Tau Beta Pi and Eta Kappa Nu. Rick holds a BS degree in computer-systems engineering from the University of Massachusetts at Amherst. His interests include research in the areas of distributed processing, reconfigurable processor architectures and  $\mu$ P applications.



Article Interest Quotient (Circle One)  
High 476 Medium 477 Low 478



# Non-volatile memories keep appliances out of the dark

Richard Orlando, Xicor Inc., Milpitas, CA

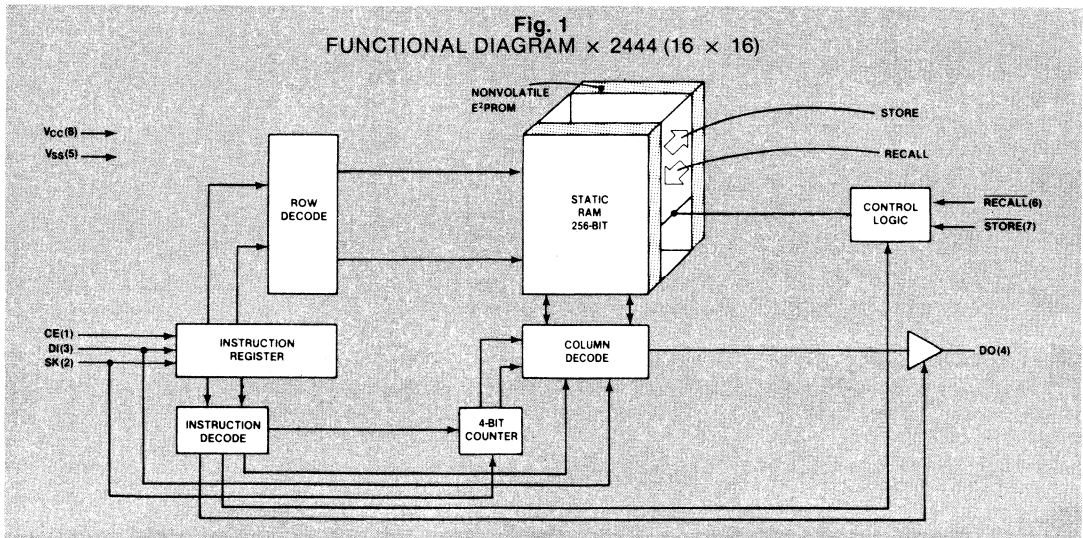
Appliance design has undergone a revolution in recent years. The advent of the low-cost, single-chip microcomputer has opened many applications for these small computers in the appliance market. Initial applications were based upon new types of appliances where digital control was a necessity. Today one sees even the venerable "white goods" using single-chip microcomputers to add features and capabilities to the end products. With this migration to digital control, a need for non-volatile memory has developed, and many new non-volatile memory devices have been made available to the designer.

Appliance control applications have gone through an orderly evolution. The design methods of the past used electromechanical devices, such as switches, relays, mechanical timers and, of course, wafer switches. The requirements of older appliances could be easily satisfied by these devices. Washing machines, for example, using multi-plane wafer switches driven by a simple timer could initiate, time and terminate the different cycles of the laundry washing process. And the electronic range allowed simple electromechanical timing of a cooking cycle.

Since the appliance industry has

been subject to the whims and attitudes of the consumer, the desired capabilities of appliances have grown as a function of added features. A simple example is the evolution of the home stove controller: first, accurate control over cooking temperature, then the ability to turn off the oven after a programmed time, and, finally, the complete programmable oven that not only turns itself off after a programmed time has elapsed, but also initiates the cooking cycle at a certain time of day.

The increased capabilities of the appliances coupled with the availability of low-cost, single-chip micro-



computers has led to the final step in the evolution, that of full digital control. The use of the microcomputer as a control mechanism allows the designer increased flexibility, reliability and precision in the control process, not easily attainable with the older design methods. Decreased development costs are also possible since a flexible digital controller can be used in a variety of different products, or models of the same product.

Microcomputer designs were not free of their own unique problems, however. The microcomputer interface required to perform the actual control functions was somewhat complex. New issues had to be addressed in terms of product reliability, since the semiconductor devices introduced different failure modes than those exhibited by electromechanical devices. The microcomputer also had a major disadvantage over prior design techniques due to its inherent volatile nature: when the power was removed from the appliance, the microcomputer not only stopped functioning, it lost any data it had maintained based upon the current state of the system.

One advantage that the older electromechanical timers possessed

was that if the power went off to the appliance, the control system would maintain the state it was in when the power was interrupted. When the power was restored to the appliance, it would continue from where it left off. One can easily appreciate the irritation of a homemaker who, having left a roast in the oven, returns from errands to find that it had not resumed cooking after a blackout.

### Emergence of non-volatility

With many appliance designs, there is a definite need to prevent such untoward situations. Some type of non-volatility is a necessity in appliance design. Since the cost of the appliance is a great concern, this non-volatility must be cost-effective. One of the earlier approaches was that of battery backup on the microcomputer itself, or on a separate CMOS memory in the system. The disadvantages of this approach are based simply on the limitations of batteries and the cost of implementation. Unfortunately, there were not many alternatives until now.

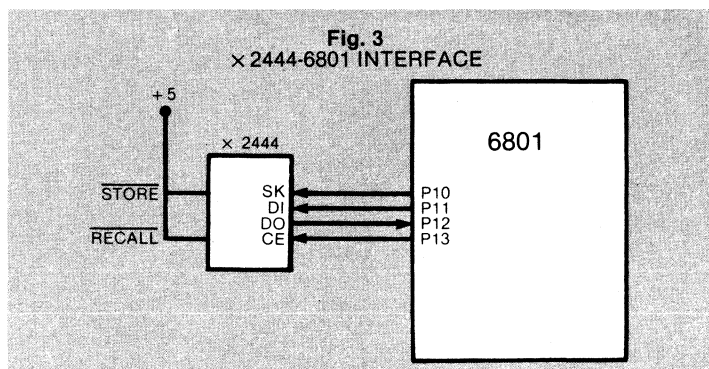
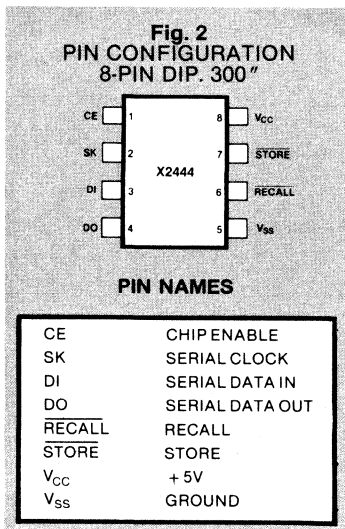
The past five years have seen a remarkable evolution in the emergence of semiconductor non-volatile memories. Unlike the battery backup of the data in either on-board or external RAM, these devices were able to retain data without the external power, in a manner similar to that of an EPROM. The main difference between these devices and the EPROM was their ability to be

“rewritten in-circuit, as opposed to being removed from the circuit, erased, and then “reprogrammed” before they were put back into the circuit.

Unfortunately, these early devices were expensive and difficult to use. They required multiple “programming” voltages, extensive support circuitry, and were quite unreliable. These devices, for the most part, were organized for microprocessor “bus” applications, and as such required too many I/O lines for efficient interfacing to single-chip microcomputers, where I/O lines are a precious commodity.

The development of 5v floating-gate, NMOS non-volatile memories eliminated many of the disadvantages of semiconductor non-volatile devices. These devices not only decreased the support circuitry required for their use, but increased the reliability of the devices. Unfortunately, these devices were also designed for “bus” applications and were relatively expensive due to their large densities (>1k bits). A need was recognized in the appliance and other industries for an inexpensive and reliable non-volatile memory designed exclusively for interfacing to single-chip microcomputers.

The Xicor X2444 answers this need. The device is a low-cost 16 × 16 non-volatile static RAM (NOVRAM for short) which features serial interface designed for interfacing to a single-chip microcomputer with a minimum requirement for both I/O



lines and software. Housed in an eight-pin mini-DIP, the X2444 provides inexpensive non-volatile data storage for both operational and configuration parameters. Its low cost (less than \$4.00 in unit quantities) makes it the least expensive non-volatile storage on the market, even rivalling the DIP switch in unit cost, while providing the equivalent of 32 DIP switches in terms of data capacity.

#### **The NOVRAM concept**

The NOVRAM idea is not new. Xicor invented this type of memory more than three years ago. The concept is quite simple. Figure 1 shows a block diagram of the X2444. It consists of a 256-bit ( $16 \times 16$ ) static RAM with a 256-bit 5V E<sup>2</sup>PROM array overlaid bit for bit in a "shadow" type manner. Two signals,  $\overline{\text{STORE}}$  and  $\overline{\text{RECALL}}$ , control the transfer of data between the E<sup>2</sup>PROM array and the static RAM. The STORE function replicates the data which is currently in the RAM into the non-volatile E<sup>2</sup>PROM array. In a similar manner, the RECALL function transfers the non-volatile data in the E<sup>2</sup>PROM array into the RAM. One can see that by simply performing a STORE during power failure, the data is then retained in the non-volatile E<sup>2</sup>PROM, and can be restored to the RAM using the RECALL once power is returned to the system.

The X2444's serial interface method is ideal for microcomputer applications. Figure 2 shows the pinout and signal designation for the X2444. The four-line serial interface consists of a Chip Select (cs), a Serial Clock (sc), a Data In (di) line, and a Data Out (do) line. The Data In and Data Out timings are designed to allow the implementation of a single Serial Data line by typing both Data In and Data Out to a single i/o line from the microcomputer, reducing the i/o lines to three. All data transfer to and from the X2444 are performed over this serial interface by either synchronous 8-bit instructions or 16-bit data operations. The X2444 has two external pins,  $\overline{\text{STORE}}$  and  $\overline{\text{RECALL}}$ , for performing the non-volatile

operations via hardware control in the event of power failure. The X2444 also includes distinct STORE and RECALL instructions over the serial interface to allow only software control over the non-volatile operations.

The serial interface is accomplished using discrete "bit-banging" from the single-chip micro. An instruction is performed by loading an accumulator with the proper bit pattern, and shifting it out through an i/o line while toggling the serial clock low and then high again between each bit.

The software for this interface is simple, and an example of a 6801 implementation is shown in Figure 3. The software assumes that the X2444 is connected to bits 0, 1, 2 and 3 of the 6801 i/o Port 1. The interconnect between the 6801 and the X2444 is shown in Figure 4. The three main parts of the software segment are three subroutines, SHIFIN, SHIFOUT and DRIVE. The SHIFOUT routine takes the eight bits of data in the A accumulator, and shifts it out through Bit 1 of Port 1. Between each data bit output the clock is toggled. This routine is used for either instruction or data output to the X2444.

The SHIFIN subroutine gives the X2444 eight clock cycles, and shifts the data from the X2444 into the A accumulator. This routine is used only in the READ instruction. The DRIVE subroutine actually provides the driver to interpret the desired operation and issue the proper sequence of commands to the X2444. It should be noted that this sample interface uses the software-controlled STORE and RECALL commands and leaves the X2444 STORE and RECALL inputs tied to Vcc.

#### **E.g. . . . microwave oven controller**

One of the newest appliances in the consumer environment is the microwave oven. This also proves to be an ideal example for the application of a non-volatile memory.

The microwave oven started with a control mechanism which was no

more than the simple electromechanical timer borrowed from electric ranges. Since the microwave oven cooks in times which are orders-of-magnitude faster than a conventional stove, it became apparent that an accurate and precise control mechanism was needed. The microwave was one of the first appliances to embrace full digital control using a single-chip microcomputer.

Figure 5 shows a typical microwave oven control system based upon the 6801 microcomputer. The user interface includes a keyboard, alarm and display, while the oven interface includes the magnetron control, door interlock, and an optional temperature probe. Non-volatile memory has been added to the system design through the use of an X2444. The interface method to the 6801 and the driving software are similar to that above. The key difference to note is the addition of an external signal to drive the  $\overline{\text{STORE}}$  input. This allows the controller to automatically store the data in the RAM into the E<sup>2</sup>PROM upon Power-Failure. The circuitry in the power supply senses a loss of power by monitoring either the ac or unregulated dc levels. Once a power failure has been detected, the power supply circuitry pulls the  $\overline{\text{STORE}}$  input low. The power supply circuitry need only ensure that Vcc is held valid to the X2444 for 10 msec, and all of the data in the RAM will be stored into the E<sup>2</sup>PROM array. Upon Power-on-Reset, the 6801 issues a RECALL command to the X2444, and all of the data is restored.

The remainder of the microwave control circuitry is fairly standard. A  $4 \times 4$  keyboard provides an input mechanism for the user, while the status indicators and display provide visual feedback. A two-line magnetron control allows the use of variable power levels in the cooking process. Timing is performed using the 6801's internal 16-bit timer which is driven off the 60-Hz reference from the power supply. Standard features include a safety door

## ELECTRONICS IN DESIGN

interlock and alarm. Optional features are provisions for a temperature probe for magnetron control or temperature-based cooking algorithms. The a-d converter used for temperature sensing has a serial interface similar to that of the X2444, and is placed on the same serial bus. Distinct chip selects enable the X2444 or the a-d converter to be accessed. Many such devices are currently on the market including the new TLC540 from Texas Instruments.

The X2444's non-volatile memory serves many functions in this application. Frequently used recipes or cooking sequences can be stored so that the microwave will sequence through a complex cooking algorithm automatically. The X2444's ability to store the data currently in the RAM into the E<sup>2</sup>PROM is very useful here. As the cooking process takes

place, the 6801 keeps a copy of the preset time and power setting in the X2444's RAM. As cooking time elapses, a location in the X2444 is updated to show the elapsed time. In the event of a power failure, the current values of these variables are automatically stored into the E<sup>2</sup>PROM section of the X2444. Once power is restored to the microwave, the data in the E<sup>2</sup>PROM is loaded into the RAM section of the X2444, and cooking continues from where it was interrupted. Intelligence can be added to the control algorithm to compensate for the continued cooking (due to retained heat) that occurs after the power outage.

The X2444's unique NOVRAM architecture makes such an application feasible. Since current E<sup>2</sup>PROM technology has limitations on the number of times that the non-volatile data

can be changed, one would not want to change the contents of the E<sup>2</sup>PROM each time the timer was incremented. If one were to use a typical E<sup>2</sup>PROM with a write limitation of 10,000 writes, the device would be worn out in a relatively short period of time at a write rate of one per second. Instead, the X2444 allows the system to update the E<sup>2</sup>PROM section of the chip only in the event of a power failure while using the unlimited RAM write capability of the X2444 every time the counter value changes.

The X2444's can also be used for a variety of other purposes in microwave design. As was mentioned earlier, one can save development time and money if a universal controller is designed. Many different models could use the same controller simply by adding circuitry

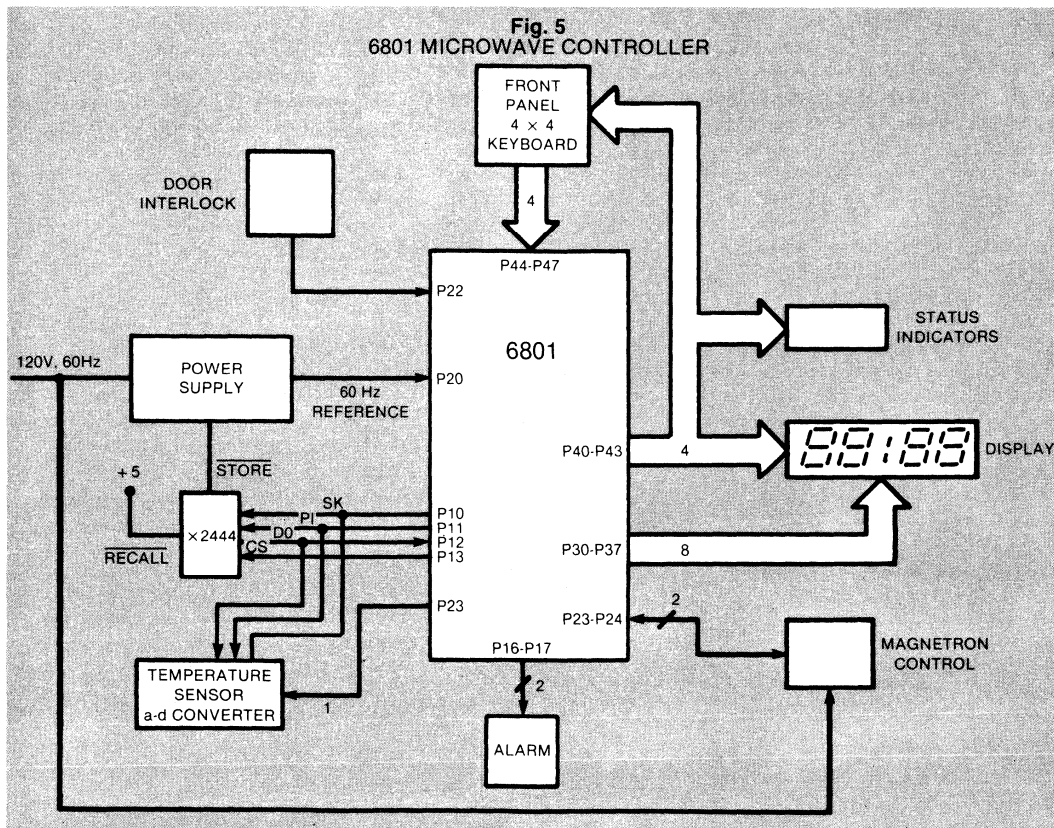


Fig. 4

X2444 DRIVER PROGRAM FOR 6801

PAGE - 1  
File: X2444

CODE AS OF AUGUST 22, 1983 Minimal Driver for X2444, 6801 Version 3.0

```

0000:                ,TITLE 'X2444 DRIVER PROGRAM FOR 6801'
0000:                ,ABSOLUTE
2 blocks for procedure code 7440 words left
0000:                ,PROC X2444
Current memory available: 7992
0000:                ,ORG 1000H
1000:                ;*****
1000:                ;                               6801 X2444 DRIVER
1000:                ;                               ASSUME THAT PORT1 IS USED AS THE 2444 INTERFACE
1000:                ;                               PORT1'S REGISTERS ARE LOCATED AS FOLLOWS
1000:                ;
1000:                ;                               DATA DIRECTION      HEX 0000
1000:                ;                               PORT                HEX 0002
1000:                ;
1000:                ;                               PORT1          X2444
1000:                ;                               SERIAL CLOCK    SERIAL CLOCK
1000:                ;                               SERIAL OUT      SERIAL IN
1000:                ;                               SERIAL IN       SERIAL OUT
1000:                ;                               I/O 3          2444 SELECT    CHIP SELECT
1000:                ;
1000:                ;                               COMMANDS ARE PASSED TO THE X2444 ROUTINE BY A PARAMETER IN THE
1000:                ;                               A ACCUMULATOR, WHILE THE ADDRESS IF NEEDED IS PASSED ON THE STACK
1000:                ;                               SERIAL DATA IN OR OUT USES THE TEMPORARY LOCATION TEMP1,
1000:                ;                               WHICH IS A SIXTEEN BIT WORD.  THE X2444 COMMANDS ARE ENCRYPTED AS
1000:                ;                               FOLLOWS.
1000:                ;                               COMMAND CODE      INSTRUCTION          OPCODE
1000:                ;                               0                  READ              1AAAA11X
1000:                ;                               1                  WRITE             1AAAA011
1000:                ;                               2                  RESET WRITE ENABLE 11111000
1000:                ;                               3                  STORE              11111001
1000:                ;                               4                  SLEEP              11111010
1000:                ;                               5                  SET WRITE ENABLE  11111100
1000:                ;                               6                  RECALL             11111101
1000:                ;
1000:                ; *1's ARE USED INSTEAD OF DON'T CARE TO DISTINGUISH BETWEEN DATA AND
1000:                ; NON DATA OPERATIONS.
1000:                ;*****
1000: 0000 DIRECTION1 ,EQU 00.
1000: 0002 PORT1      ,EQU 02.
1000: 0080 TEMP1     ,EQU 080H ;RAM STORAGE FOR DATA
1000: 0082 COUNT    ,EQU 082H ;COUNTER VARIABLE
1000: 0084 DATUM    ,EQU 084H ;DATA STORAGE
1000: 0086 ADDRESS  ,EQU 086H ;ADDRESS STORAGE
1000: 0088 ERRORDATA ,EQU 088H ;ERROR DATA
1000:                ;*****
1000:                ;                               PROCEDURE INIT
1000:                ;                               THIS PROCEDURE INITIALIZES THE X2444 INTERFACE
1000:                ;*****
1000: 06 1E INIT     LDA# #1BH ; B=1011, I/O 0,1 AND 3 OUTPUTS, 2 INPUT
1002: 97 00        ST# DIRECTION1 ; WRITE TO DATA DIRECTION REGISTER
1004: 4F          CL# 0 ;SET CE TO 0(INACTIVE), DOUT AND SK TO 0
1005: 97 02        ST# PORT1 ;AND STORE IN DATA PORT
1007: 39          RTS ;
1008:                ;*****
1008:                ;                               SHIFTER ROUTINE- SHIFT1
1008:                ; THIS ROUTINE TAKES THE DATA IN THE A ACCUMULATOR AND CLOCKS IT MOST
1008:                ; SIGNIFICANT BIT FIRST INTO THE X2444.  THE FLOW IS SHIFT A BIT, TOGGLE
1008:                ; THE SERIAL OUTPUT(6801) ACCORDING TO STATE, AND TOGGLE SERIAL CLOCK
1008:                ;*****
PAGE - 2 X2444 X2444 DRIVER PROGRAM FOR 6801
File: X2444 CODE AS OF AUGUST 22, 1983 Minimal Driver for X2444, 6801 Version 3.0
1008: C6 08        SHIFTOUT LD# #08. ;LOAD THE BIT COUNT WITH 8
100A: D7 82        ST# COUNT ;STORE IN COUNTER
100C: 49          SHIFTOUT ROLA ;SHIFT BIT INTO CARRY BIT
100D: C6 14        LD# #14H ;WE SET DATA OUT TO ZERO, WHILE SETTING CHIP
100F:                ;ENABLE. SERIAL CLOCK IS LOW.
100F: 24 **        BCC TRANS ;IF BIT IS A ZERO, THEN TRANSMIT
1011: CA 02        OR# #02H ;IF IT IS A ONE, THEN SET DATA OUT
1013: D7 02        ST# PORT1 ;STORE THE DATA INTO THE PORT
1015: CA 01        OR# #01H ;AND SET THE CLOCK FOR A TRANSITION
1017: D7 02        ST# PORT1 ;BY WRITING A 1 TO SERIAL CLOCK
1019: C4 1A        AN# #1AH ;KEEP THE DATA VALID, BUT SET SK TO ZERO
101B: D7 02        ST# PORT1 ;AND STORE IN THE PORT
101D: C6 14        LD# #14H ;TOGGLE CLOCK DOWN, SET DOUT TO 0, BUT KEEP
101F: D7 02        ST# PORT1 ;X2444 SELECTED
1021: 7A 0082      DEC COUNT ; DECREMENT THE BIT COUNTER
1024: 26 E6        BNE SHIFT1 ;IF COUNT IS NOT ZERO, TRANSMIT NEXT BIT
1026: 49          ROLA ;ONE MORE ROTATE TO PRESERVE INSTRUCTION
1027: 39          RTS ;RETURN FROM SUBROUTINE
1028:                ;*****
1028:                ;                               SHIFTOUT ROUTINE
1028:                ; THIS SUBROUTINE SHIFTS IN 8 BITS OF DATA INTO THE A ACCUMULATOR FROM THE
1028:                ; PORT TO ENTER WITH THE CLOCK LOW
1028:                ;*****

```



## **ELECTRONICS IN DESIGN**

external to the 6801 microcomputer. Configuration information can be stored in the X2444 at time of manufacture which the 6801 can then determine upon Power-on-Reset to control the features and functions of its particular microwave. Additional X2444s can be added on the serial bus as user or model options. These optional X2444s require only an additional chip select, and can be used for such features as increased recipe storage or operational modes. The X2444's non-volatile memory also can be used for calibrating the temperature probe and storing the response time of the magnetron to allow quick calibrations or more complex and precise temperature-control algorithms.

### **General applications**

There are many other areas in the appliance field which are natural applications for the X2444. Since most electronic appliance controllers utilize the single-chip microcomputer, the X2444's serial bus is the ideal solution their non-volatile storage needs.

"User-programmable" parameters such as favorite stations, cooking algorithms or preset time-of-day events all make the appliances more "user-friendly" especially if these parameters are retained in the event of power loss. System configuration parameters can be stored in the X2444 to allow the design of appliances in a modular fashion, substantially reducing development costs while

increasing the reliability of each new product. System status saved in the X2444 in the event of a power failure is restored upon Power-On so that the system can complete interrupted tasks as well as ensure that the appliance is left in a safe and stable state.

The availability of the new 5V non-volatile memories allows the appliance designer to add more features and capabilities for a minimum cost. Whether it be used for power-failure data storage, or as user set-up information, the X2444 will make appliance designs less complex, more cost-effective, more fault-tolerant, and easier to use. □

Reprinted from **DESIGN NEWS**, October 1983  
© 1983 by CAHNERS PUBLISHING COMPANY



# NONVOLATILE MEMORY GIVES NEW LIFE TO OLD DESIGNS

Terminals and other equipment can be made more flexible, and product life can be extended by upgrading and customizing with NOVRAMs and EEPROMs.

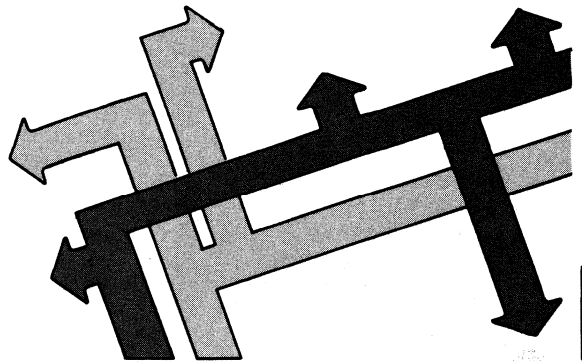
by **Richard Orlando**, *Xicor, Inc., Milpitas, Calif.*

The recent appearance of low cost, 5-V nonvolatile memories has led to design applications that can be broken into two distinct classes. One class uses nonvolatile memory to store such data as configuration or calibration parameters. This information can be updated and then stored in the device for access on power-up. The second application uses nonvolatile memory for program storage. Here, the nonvolatile memory's main advantage is that content can be updated or changed remotely, rather than by device replacement.

Unfortunately, many end products completed prior to the availability of these devices are threatened by newer designs. The latter take advantage of the added flexibility and features afforded by nonvolatile memory. There are, however, ways to add nonvolatile memory to existing designs without a major redesign.

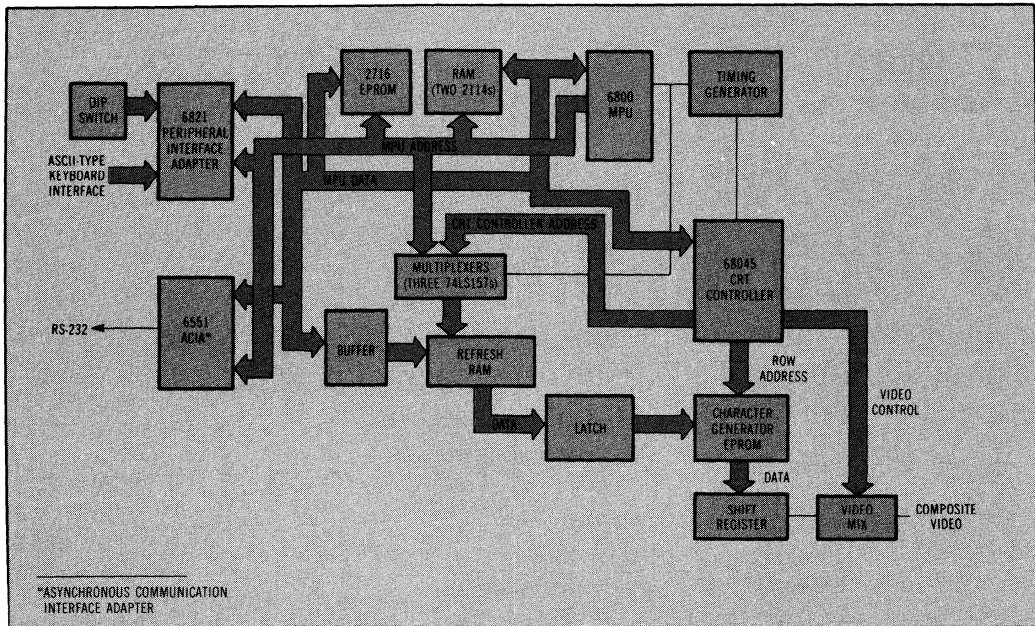
For example, consider the schematic of an intelligent terminal design, which will be used to illustrate methods that improve the flexibility of almost any microprocessor-based design (Fig 1). Here, the 6800 processor is the source of the "intelligence" in

*Richard Orlando is product marketing manager at Xicor, 851 Buckeye Ct, Milpitas, CA 95035. He holds a BS in computer systems engineering from the University of Massachusetts at Amherst.*



the design. The serial communication channel is through a 6551 asynchronous communication interface adapter (ACIA), which features an onchip baud rate generator. A 2716 erasable PROM is the program store for the 6800, and the two 2114 RAMs provide 1 Kbyte each of buffer, stack, and parameter storage. The keyboard is an ASCII-encoded type whose inputs are fed through one port of a 6821 peripheral interface adapter (PIA). The other port of the 6821 receives the dual inline package (DIP) switch settings for such user-defined operational parameters as baud rate, parity, and protocol selections.

Video control is provided by a 68045 (or 6845) CRT controller. The display RAM interface is set up as a tightly coupled, shared RAM interface. The timing



**Fig 1** The original terminal design has dual inline package (DIP) switch settings that must be read by the processor. They are then parsed to determine setup parameters invoked from the terminal program contained in the EPROM.

is such that the CRT controller only accesses the data in the display RAM during the bus “dead” time of the 6800. This allows the processor to access the data in the display RAM at any time, regardless of the state of the CRT controller. The CRT controller can access the RAM transparent to the processor, and thus can relieve the processor of any access arbitration tasks.

### Improving the design

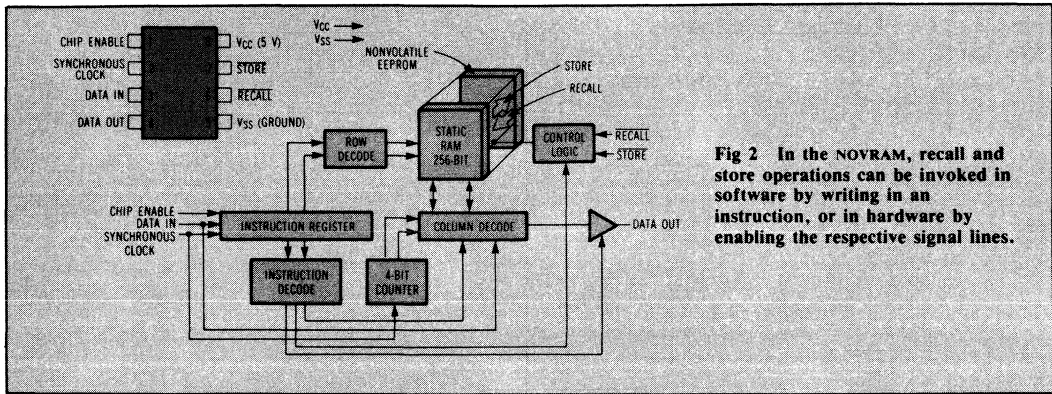
Although the design serves its initial purpose, several areas, which will make it more flexible and possibly extend the life of the product, can be improved. Intended for use in a variety of applications, the original design relies primarily on software for its characteristics and “feature set.” Simple changes to the erasable PROM containing the 6800’s software allow such terminal “customization.” This approach is adequate when end-user needs are known prior to manufacture. However, if a user wants to upgrade an existing terminal, someone must perform a costly EPROM change in the field. The same penalty applies to the manufacturer who wishes to “upgrade” the software of the existing units in the field, in order to increase performance or to eliminate possible errors.

The second area in need of improvement is the DIP switch used for the input of user-definable parameters. It creates many manufacturing problems, since most DIP switches cannot be

handled by automated assembly equipment, such as insertion machines and wave solderers. Additionally, because someone must manually toggle the switch through a sequence of positions in order to fully test the boards, DIP switches slow down automated board testing. Also, to change parameters, a DIP switch requires the terminal user to remove an access panel and manipulate switch toggles while referring to a manual. As the range of user-definable parameters expands to include such features as emulation modes, the problem becomes even more awkward.

In the example terminal, added features and enhancements can be made in two ways. The first involves replacing the DIP switch with an X2443 serial NOVRAM, which is used to store user-defined setup and configuration parameters. The second replaces the EPROM with an electrically erasable PROM.

The NOVRAM, a 256-bit serial device, is organized as 16 words of 16 bits each. All communication between the device and the processor is done in a bit-serial fashion using the data in input, data out output, and the synchronous clock lines shown in Fig 2. All operations are controlled by the micro-processor through the serial interface. Read and write operations are executed through the transmission of a specific 8-bit instruction code with an embedded address of the word to be accessed. In the write operation, the processor follows the write command with 16 bits of data to be written. In the



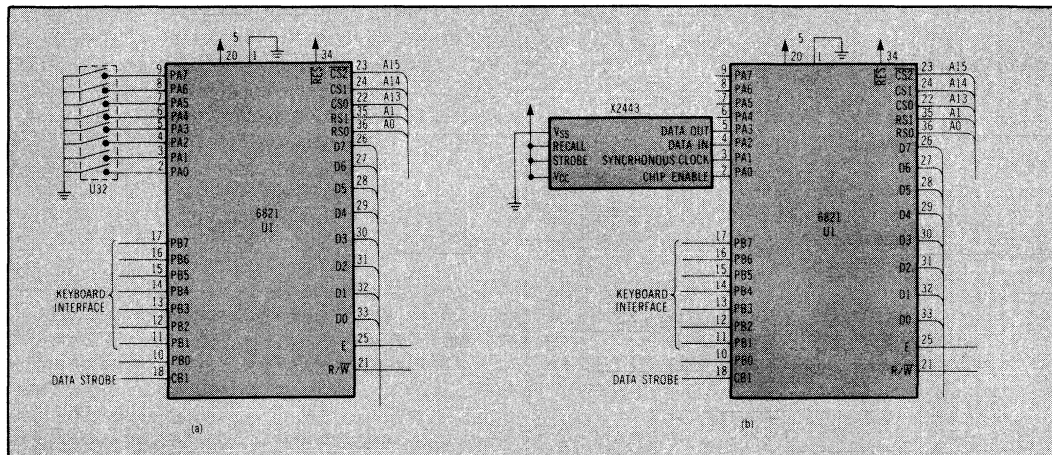
**Fig 2** In the NOVRAM, recall and store operations can be invoked in software by writing in an instruction, or in hardware by enabling the respective signal lines.

read operation, the processor supplies the read instruction, and then gives the X2443 16 clock cycles, which the device uses to output the data to be read. The NOVRAM also includes several non-data types of instructions to control the nonvolatile operation of the part, the part's power consumption, and the write/store lockout feature.

The X2443 is designed to interface with single-chip microcomputers when the main consideration is minimizing I/O lines and software overhead. This device also works well in microprocessor-based designs requiring upgrading with minimal design changes. It consists of a serial static RAM overlaid or "shadowed" bit-for-bit with a 5-V EEPROM array, as shown in Fig 2. The execution of a store operation, either from the input STORE or by the execution of the software store instruction, transfers the current contents of the SRAM *en masse* into the nonvolatile EEPROM array. In a similar manner, the execution of a recall operation, via the RECALL

input, transfers the contents of the nonvolatile EEPROM array into the SRAM array. On power-up, the contents of the EEPROM array are automatically loaded into the RAM array for a default configuration.

When using the X2443 to replace an existing DIP switch, it is advantageous to drop the NOVRAM into the existing switch "footprint." Fig 3 shows the simple conversion of the existing site or socket (a) to accept the X2443 (b). Four of the eight 6821 I/O lines used to read the DIP switch are already mapped into pins 1 through 4 of the NOVRAM. These lines originally input the current settings of the DIP switches, but can be configured through the 6821's data direction register to serve as the three outputs and one input needed for interfacing the NOVRAM. Since hardware STORE and RECALL signals are not needed in this application, they are simply tied to V<sub>CC</sub>. All nonvolatile operations occur through software control, whose requirements are relatively



**Fig 3** Within both the original DIP interface (a) and the X2443 implementation (b), the interface is serial. Therefore, only the clock, enable, data input, and data output lines need to be used.

PROCEDURE RESET  
THIS PROCEDURE IS RESPONSIBLE FOR CONFIGURING THE TERMINAL TO THE MODES SPECIFIED. AT POWER-UP TIME ON THE FUNCTION DIP SWITCHES TIED TO PIA PORT A

BITS	7	6	5	4	3	2	1	0
PORTA PARITY	AUTOLF	AUTONL	DUPLEX	LINE	--BAUD RATE--			
0=ODD PARITY								
1=EVEN PARITY								
AUTO LINE FEED								
0=NORMAL								
1=AUTO LINE FEED								
ICR ALWAYS FOLLOWED BY LF								
AUTO NEW LINE								
0=NORMAL (INPUT STOPS AT LINE END)								
1=AUTO NEW LINE (INPUT WRAPS AROUND)								
FULL/HALF DUPLEX								
0=HALF DUPLEX								
1=FULL DUPLEX								
LINE/LOCAL								
0=LOCAL								
1=LINE								
BAUD RATE SELECTION	.....							
000= 50 BAUD	.....							
001= 110 BAUD	.....							
010= 300 BAUD	.....							
011= 600 BAUD	.....							
100=1200 BAUD	.....							
101=2400 BAUD	.....							
110=4800 BAUD	.....							
111=9600 BAUD	.....							
SUBSIDIARY PROCEDURES	HOME	CLEAR						
GLOBAL VARIABLES	.....							
USED	NONE							
ALTERED	CAPIA	.....						
	CEPIA	.....						
	DAPIA	.....						
	DEPIA	.....						
	HEAD	.....						
	TAIL	.....						
	AUTOLF	.....						
	NEWLIN	.....						
	FULDUP	.....						
	LOCAL	.....						
	CMACIA	.....						
	CMACIA	.....						
	A ACCUMULATOR	.....						
	B ACCUMULATOR	.....						

Fig 4 When using a header for a parsing program used with the DIP switch configuration, the possible parameters are limited to 8 bits, and an elaborate software routine is needed to interpret them.

straightforward (as described). With this software in place, the communication between the processor and the device simply becomes a series of reads or writes to the appropriate serial device locations.

The original design only allowed eight user-definable inputs, since only one DIP switch is used in the terminal. The meaning of the various input conditions is shown in the DIP switch map portion of the program header in Fig 4. Since the single 8-bit input is used for so many functions, parsing the input byte into the appropriate setup parameters requires an extensive piece of code. The problem with this implementation is the extensive software required

to make switch operation straightforward in the user's manual.

Replacing the DIP switch with the NOVRAM has several significant advantages. The 256-bit nonvolatile storage leaves adequate room for storing an "image" of all interface circuit registers. Thus, the parsing problem of the DIP switch implementation is eliminated. Even the control registers that do not need to be user-programmable can benefit from this imaging, since they can be changed remotely in the field for hardware or software updates. This method simplifies field upgrading when compared with the usual method of storing these register images in the program store ROM or EPROM.

New images can either be down-loaded remotely or loaded through a diagnostic mode using a direct-connect RS-232 interface. Examples of where this capability is beneficial are numerous, and include changing interface protocols, data formats, or other hardware, interface, or networking options.

The use of the device for storing setup parameters also allows a more user-friendly operator interface. Software in the original design includes routines that allow random placement of the cursor or text through the use of a "go to X-Y" routine. It becomes a fairly trivial task to implement a menu-driven setup mode. After entering a certain escape sequence, the user is placed in the configuration mode, which presents an English menu.

The return key increments the cursor position to the next setup area where the current setting is displayed, and the spacebar key increments that setting through all possible choices. Once the user has set up the parameters for a particular session, depressing the escape key writes the current settings into the RAM section of the NOVRAM. With this operation, the user can set up a temporary configuration without changing the default parameters in the EEPROM section of the NOVRAM. Default settings are changed only when the user executes a certain control sequence (such as control X and then the escape). In some applications, it may be desirable to allow only certain users to change these default parameters before entering a special code.

### *Replacing the DIP switch with the NOVRAM allows increased design flexibility, as well as reduced manufacturing and testing costs.*

Since the X2443 has a much larger capacity than actually needed for this application, the remainder of the nonvolatile storage can hold such data as serial number of the individual unit, revision level, and hardware configuration diagnostic parameters. Otherwise, it can be reserved for future expansion. The Table shows a sample address map for the

NOVRAM Address Map		
Location	Bit map	Interpretation
0	XXXXXXXXSWWXBBBB	S = Stop Bit Control WW = Word Length BBBB = Baud Rate
1	XXXXXXXXPPPETTRD	PPP = Parity Check Controls E = Normal/Echo Mode TT = Transmit Controls R = Receiver Interrupt Enable D = Data Terminal Ready Control
2	XXXXXXXXEEEEEEEE	E = Emulation Designator (1 of 256)
3	SSSSSSSSSSSSSSSS	S = Serial Number
4	RRRRRRRRRRRRRRRR	R = Revision Level
5	XXXXXXXXXXXXXXXXXX	L = Latch data from keyboard on high-to-low or low-to-high

X = Don't Care

device, with the associated data stored in each of the 16-bit locations. The end results of replacing the DIP switch with the NOVRAM are increased design flexibility, as well as reduced manufacturing and testing costs.

### Program storage considerations

The second aspect of improving the terminal design involves the program store for the 6800 microprocessor. The original design uses a 2716 EPROM since the software requirements for the terminal are not extensive. The feature set of the X2816A EEPROM makes the replacement easier because EEPROMs of the X2816A generation incorporate high voltage generation, address and data latching, and the write-cycle timing circuitry on the memory chip. During read operations, the device functions just like the 2716 EPROM in its use of chip enable ( $\overline{CE}$ ) and output enable ( $\overline{OE}$ ) signals. During a write operation, the X2816A latches the addresses on the bus during the high to low transition of the write enable ( $\overline{WE}$ ) signal, and then latches the data to be written on the rising edge of the WE signal.

The duration of this signal is not important, since the EEPROM only uses it to initiate the write cycle; the timing for the write operation is generated on-chip. The processor needs only to ignore the EEPROM for 10 ms during the write cycle, and the device does the rest. The latched and self-timed nature of the X2816A allows it to be placed in a 16-K SRAM socket and be read and written with the same signals used for the SRAM.

The read operation of the X2816A is the same as that of the 2716 EPROM, so this part of the EEPROM operation is of no concern. The only changes required to the existing circuitry involve the write operation. The first change allows the processor to write to the EEPROM, and the second protects the EEPROM from unwanted write operations during power-up and power-down.

The memory map for the original design was not very full, so only large blocks of the address map

are decoded for each memory device and I/O chip on the bus. The 2716 logically resides at addresses F800 through FFFF since the 6800 reset vectors must be included. The physical decoding for the 2716 includes the address range of F000-FFFF since only the microprocessor's two most significant address lines A15 and A14 are used for the decoding.

Since line A14 is used to drive the  $\overline{OE}$  line of the 2716, the EPROM is selected whenever A15 is a logical one. Possible conflict with the system RAM residing at 8000-81FF is avoided by restricting the processor's access to the 2716 in the logical F800-FFFF range. Since the processor can now read and write to the logical address range of the 2716 socket, the  $\overline{CE}$  must also be derived from the A15 and A14 address lines. And, since  $\overline{CE}$  is active low and the address line is active high, a simple NAND gate will suffice (Fig 5). Luckily, an extra NAND gate in the

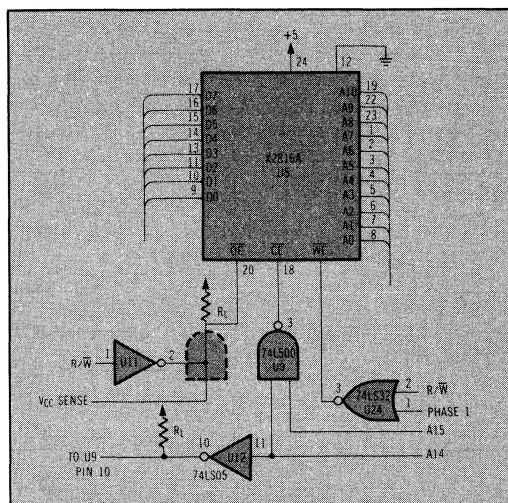
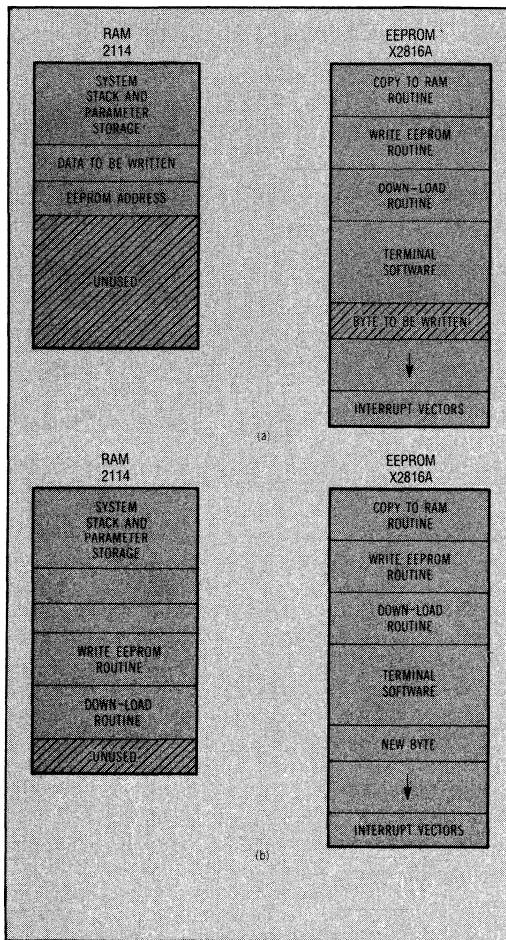


Fig 5 The EEPROM control logic uses the processor's high order address lines to map the device into the proper address range and enable it at the same time.



**Fig 6** Address maps for updating EEPROM software are kept in EEPROM (a) and copied to RAM (b) when needed.

design can be used as an inverter. The inverter used for the  $\overline{CE}$  is no longer needed, and therefore can replace the NAND gate. The inverter on A14 must remain intact since it is used in the 2114 RAM decode circuit.

The  $\overline{WE}$  line for the X2816A EEPROM can be derived from the composite RAM write signal used for the 2114 RAMs. This signal is the logical OR or the  $R/\overline{W}$  output from the 6800 and the Phase 1 clock signal. This qualification of the  $R/\overline{W}$  line ensures that the addresses are valid on the high to low transition of the  $\overline{WE}$  signal. Therefore, they can be latched into the EEPROM. This ORing connection also guarantees that the data to be written is valid on the rising edge of the composite  $\overline{WE}$  signal. The  $\overline{OE}$  signal on the EEPROM can simply be driven from the complement of the  $R/\overline{W}$  signal from the processor. This

technique requires that all accesses to the EEPROM be made in the logical address range of F800-FFFF to avoid bus contention with the system RAM.

Discussion of the circuitry needed for the  $\overline{OE}$  signal also must include another important issue: ensuring that the chip does not experience an accidental write cycle during power-up or power-down. Even though the chance of  $\overline{CE}$  and  $\overline{WE}$  going low during power-up or power-down is rather remote, the possibility must be eliminated.

The EEPROM simplifies write protection by including an onchip voltage sensor that monitors the  $V_{CC}$  input level and automatically disables writes from occurring when  $V_{CC}$  falls below 3 V. Also, a noise filter on the  $\overline{WE}$  input prevents a write from being initiated by a low spike. Functional interaction of the control inputs on the chip allows a low level on the  $\overline{OE}$  to disable any write operations regardless of the state of the  $\overline{CE}$  and  $\overline{WE}$  inputs. By holding  $\overline{OE}$  low while  $V_{CC}$  is between 3 and 4.75 V, inadvertent write cycles are inhibited.

The power supply must be modified to generate an active low signal whenever  $V_{CC}$  is below a specific level. This signal disables the write operation during both power-up and power-down. Because this signal is wire-ANDed with the control signal driving the  $\overline{OE}$  signal, all writes to the chip are disabled when  $V_{CC}$  is below the 4.75-V limit.

### Software modification

Once hardware changes have been made, in-factory modifications and in-field modifications must be addressed in order to take full advantage of an X2816A. In-factory modifications can be handled in many ways. If the terminal configuration is known at assembly time, the appropriate software can be loaded into the EEPROM through the use of a standard PROM programmer. However, this method does not take full advantage of the features of the in-circuit reprogrammability inherent in the X2816A. A more advanced approach also makes automated board testing easier.

For example, the EEPROM can be initially installed with a diagnostic program for testing the completed terminal board with an automated test system. Once the board has been tested, the tester controls the 6800 processor by holding it in a quiescent state such as reset or halt. The tester then assumes control over the terminal bus and writes the actual terminal software into the EEPROM. This greatly reduces the overhead required to manufacture a variety of different configurations or "models" on a single assembly line. In-line programming also allows for the verification of the EEPROM write operation and control circuitry.

The real advantages of the EEPROM surface when it comes to modifying software in the field. In this case, the terminal is placed in a down-load mode,

---

and the software revision is loaded through the RS-232 interface, either from a service “box” or remotely via a modem. The X2816A allows the terminals in the field to be called over phone lines for loading new operating software, thereby greatly reducing the cost and impact of a software update.

Although full-featured EEPROMs such as the X2816A simplify this task significantly, there remains one software issue to be resolved. While the EEPROM is performing its internal write cycle, it is unavailable for further writes or reads. For example, the processor, executing out of a program stored in the EEPROM, might perform a write cycle to the chip and then fetch the next instruction. Since the X2816A is occupied with its internal write cycle, the next instruction fetch will yield a high impedance bus. The processor will take this data as its next instruction and enter the “catch fire and die” mode of operation.

To avoid this situation, a very compact routine fetches the byte to be written into the EEPROM from a given location, writes the byte into the EEPROM, and then enters a timing loop to wait the 10-ms period required to complete the write. Since the RS-232 interface supports full handshaking, there is no chance of overrun from the down-loaded data. This routine is initially loaded into the EEPROM, but it is never executed from this device. Instead, another

“copy to RAM” routine copies the routine from EEPROM into RAM, from which it is executed.

Since the terminal has 1 Kbyte of RAM capacity, there is ample room for storing such a routine during the EEPROM write cycle. Fig 6 shows address maps for both the EEPROM (a) and the RAM (b) prior to and during the execution of the EEPROM write routine. This method works especially well with the 6800 since its architecture is that of a von Neumann machine, and can therefore execute program segments out of the memory space reserved for RAM data storage.

In-field terminal upgradeability has two important benefits. If the terminal software is upgraded or revised after the unit is sold, the new software can be added to the existing units in the field at minimal cost. This method also eases the addition of optional hardware in the field, since the new software supporting the hardware option can be down-loaded instead of replacing the terminal EPROM.

## NOTES



A CAHNERS PUBLICATION

# EDN

ELECTRONIC TECHNOLOGY FOR ENGINEERS AND ENGINEERING MANAGERS

Save volatile  
data during  
power loss

7

# Save volatile data during power loss

---

*Nonvolatile-storage devices give you a medium in which to store data during power loss. By combining these devices with power-sensing circuits and supplying the necessary control signals, you can design a system that transfers data securely between volatile and nonvolatile memory during power loss.*

---

## *Xicor, Inc.*

To protect volatile data during power loss, you need to transfer that data reliably to nonvolatile memory during the transient and return it to RAM after power is restored. A system that performs this function includes two subsystems. The first reports power status, indicating when power is lost and when it is restored; the second handles the data transfer, using the power-status signal to generate the appropriate store and retrieve commands.

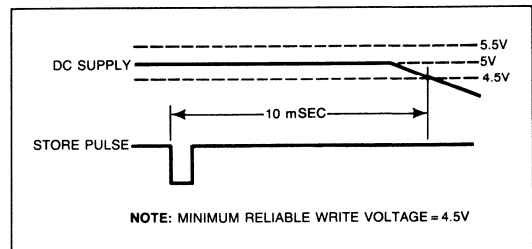
### **Sense power failure**

To transfer data reliably after power loss, a system must have enough time to copy data from RAM to nonvolatile memory before the supply voltage drops below a certain level. The sensing circuit must recog-

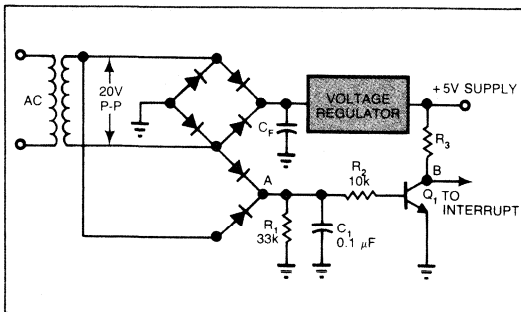
nize the power loss and generate a power-loss signal promptly, giving the storage subsystem enough time to effect the data transfer. In fact, in some systems, you may have to complete your transfer within a single write cycle to ensure a reliable transfer.

Your first step in designing the sensing subsystem is to choose a sensing point. You could use the 5V regulator's output as a sensing point, but this output will not indicate power loss as quickly as will either the ac input line to the power supply or the unregulated dc voltage supplied to the regulator.

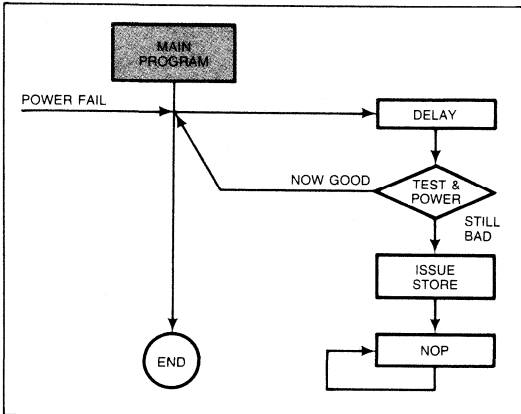
To sense ac loss on the power supply's ac input line, you can monitor either the input or the output to the power transformer. If you monitor the transformer's input side, you must electrically decouple the sensing circuit's signal from the system's dc portions (by using optoelectronic isolators, for example). If you monitor



*Fig 1—The system characterized by this timing diagram must detect a power loss early enough to allow it to generate a store pulse 10 msec before the dc supply drops to 4.5V.*



**Fig 2**—This zero-crossing detector monitors power-supply status at the transformer's ac output. The two diodes isolate the detector from the main power supply's unregulated dc bus.

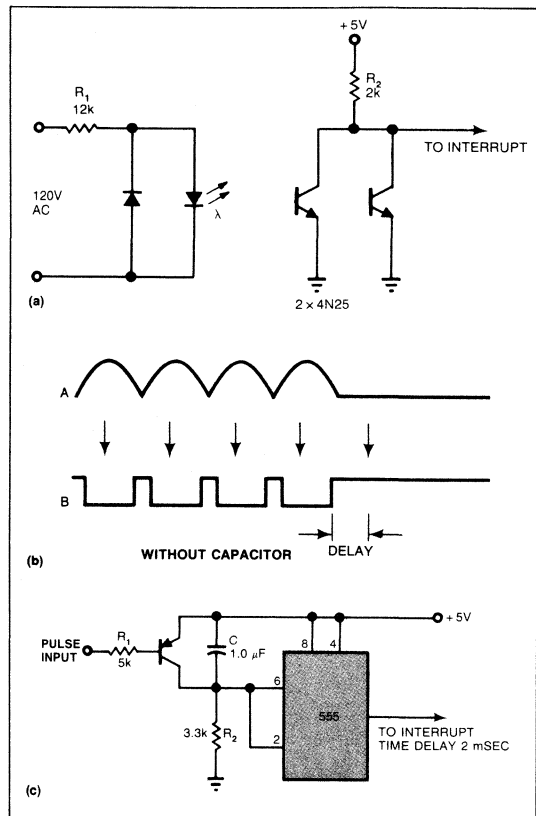


**Fig 3**—In a typical  $\mu P$  system that tests for power loss, once the processor receives an interrupt indicating a power loss, the system initiates a subroutine that tests for a true power loss. The subroutine first produces a delay of about 2 msec; then the system looks again at the power detector's output. If that output is still asserted, the system decides that the power loss is real and sends a store pulse to the nonvolatile RAM.

the output side, you must isolate the detector circuit from the main power supply's filtered unregulated dc circuit, because that circuit's response to a line fault is slow. To isolate the circuit, you can use either a separate transformer tap or two extra diodes between the bridge and the detector.

Alternatively, you can use the unregulated dc voltage ahead of the regulator as a sensing point. The regulator maintains its regulated output as long as its input voltage remains within a certain range. To make sure that the system will have time to respond to a power loss, you should set your trip point below the normal input voltage. This allows you to send your store signal early enough to ensure a reliable transfer to nonvolatile memory. Consider, for example, the timing diagram in Fig 1 and assume that the minimum reliable write voltage of the memory in the system it characterizes is 4.5V. Because this system's dc supply drops to 4.5V 10 msec after initiation of the store pulse, the system must complete a write operation to nonvolatile memory within this 10-msec period.

Once you've chosen a sensing point, you must choose a detector. If you've chosen to detect ac loss, consider one of the following four methods. The first is a low-cost zero-crossing detector (Fig 2), in which two diodes isolate the detector circuit from the filter capacitor ( $C_F$ ) that's ahead of the regulator. When a power loss occurs, the full wave's rectified ac drops to zero, inhibiting base current to transistor  $Q_1$ . This causes  $Q_1$ 's output to go high, thereby generating an interrupt signal at point B.



**Fig 4**—You can connect a detector like this one, (which contains optoelectronic isolators with their diodes connected back-to-back) directly to the ac line through a resistor (a). The circuit produces an output pulse that can interrupt a  $\mu P$  each time the input waveform crosses zero, or every 8.3 msec (b). Instead of allowing the sensor to interrupt the  $\mu P$  every 8.3 msec, you can feed these pulses first to a 555 timer that's configured as a missing-pulse detector. It issues an interrupt only when the input pulse train is interrupted (c).

*To ensure that you'll be able to transfer data reliably from RAM to EEPROM, you need to maintain power for at least 10 msec after a power loss.*

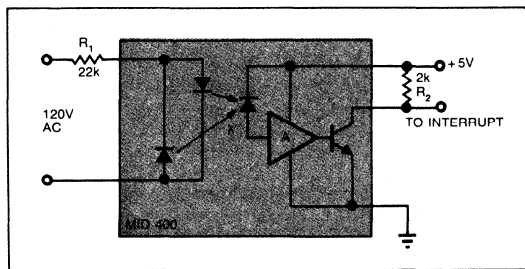
When it receives an interrupt, the system initiates a subroutine that tests for a true power loss (Fig 3). The subroutine delays the store signal for about 2 msec and then looks at the detector again. If the output is still high, the system decides that the power loss is real, and it sends a store pulse to the nonvolatile RAM. Resistor  $R_2$  in Fig 2 limits the transistor base current.

Capacitor  $C_1$  is essential in this circuit because it filters the power supply's half-cycle pulses before they're applied to  $Q_1$ . (If you were to fail to filter these pulses, the  $\mu P$  would receive an interrupt signal every 8.3 msec, whether or not a power loss had occurred. Without  $C_1$ , as much as 25% of your available processor time would be spent responding to false interrupts generated by the power-loss detector.) The value that you choose for  $C_1$  depends on the power supply's holdup time, the values of  $R_1$  and  $R_2$ , and the delay that you want between the loss of ac and the triggering of the store signal.

### Use optoisolators

The second technique for sensing ac power loss uses two optoelectronic isolators between the detector and the ac power line (Fig 4a). This technique produces a positive output pulse at each zero crossing on the ac line, or at 8.3-msec intervals (Fig 4b). The problem with Fig 4a's circuit is that the interrupt signal occupies the  $\mu P$ 's time while the rest of the system is resampling the detector's output. To solve this problem, you can add a missing-pulse detector similar to the one shown in Fig 4c.

A third detector that relies on direct ac-line connection uses General Instrument's MID 400 power-line monitor. When you use this device, you need to add only two resistors to ensure a clean interrupt signal



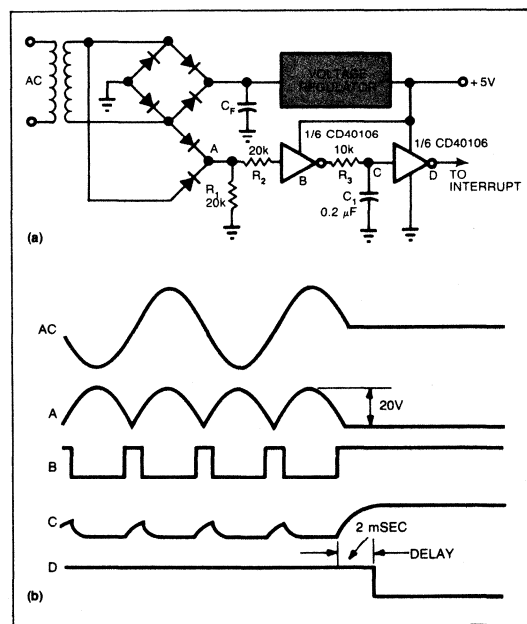
**Fig 5**—To incorporate the MID 400 detector in your sensing subsystem, you need to add only two external resistors that you connect directly to the ac line. You can control the on and off delays at the output by connecting a capacitor across  $R_2$ .

(Fig 5). You can adjust turn-on and turn-off delays by adding a capacitor across  $R_2$ .

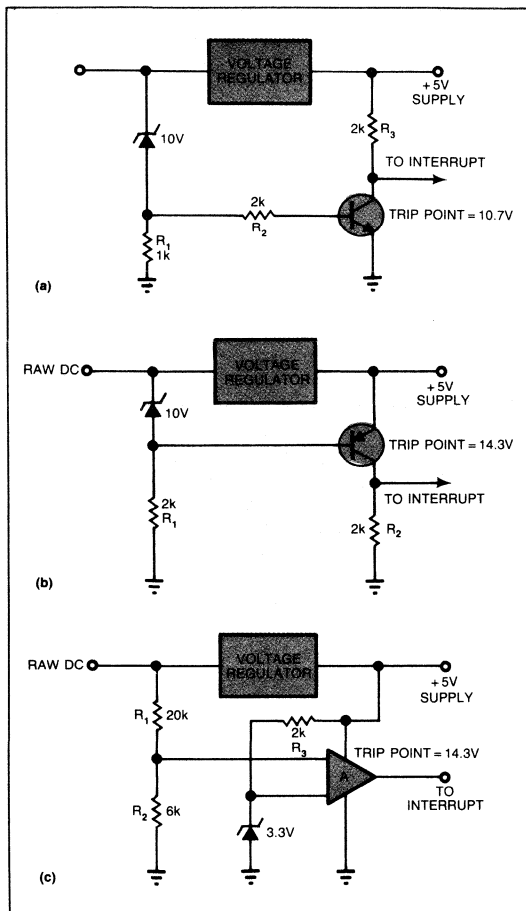
The fourth detector (Fig 6) uses a CMOS Schmitt trigger as a full-wave, low-voltage, missing-pulse detector. To avoid latch-up, and possible damage to the CMOS circuits, you must make sure that the input voltage to the CMOS Schmitt trigger does not exceed the 5V supply voltage. You can meet this requirement by inserting a resistor between the Schmitt trigger and the bridge's output. To obtain narrow pulse widths from the first gate, keep the ac input voltage as high as possible.  $R_3$  and  $C_1$  determine the output's delay, which must be longer than the first gate's pulse width.

### Sensing dc power loss

If you've decided to sense dc loss instead of ac loss, you don't have to worry about capacitor delays or missing pulses. Consider the sensor in Fig 7a, for instance. The sensor generates a negative interrupt pulse when it senses dc loss; it uses a zener diode to set the trigger point. On one hand, you should set the



**Fig 6**—When you use two Schmitt triggers to detect ac loss (a), the delay produced by  $R_3$  and  $C_1$  must be longer than the first gate's output pulse width. The timing diagram (b) shows the circuit waveforms.



**Fig 7—Using zener diodes** you can configure a power-supply detector circuit to produce either a negative (a) or a positive (b) interrupt pulse when the trigger point is reached. You can configure the op amp shown in c to produce either a positive or a negative output pulse polarity.

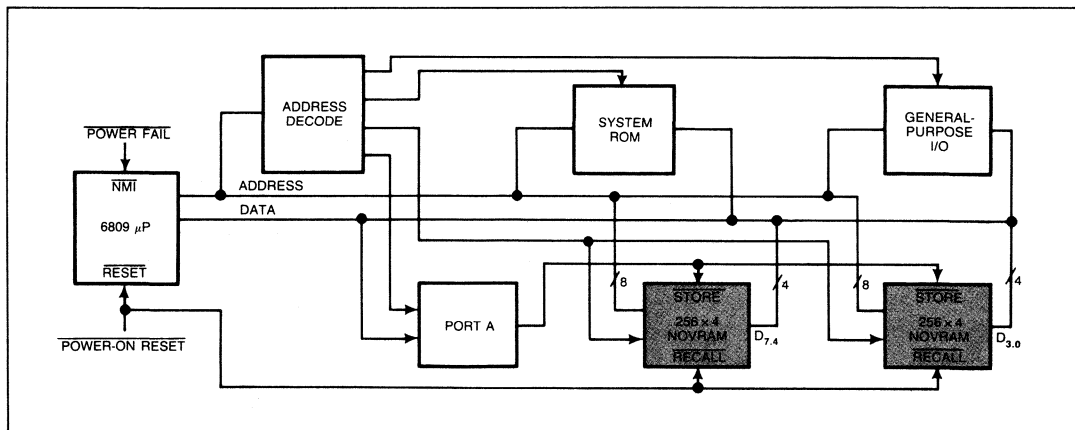
trigger point as high as possible (to allow the circuit to sense the power loss as early as possible). On the other hand, you must still set the trigger point low enough to fall below the lower boundary of the supply's upper unregulated limit (to prevent false triggering). Remember that the diode's voltage rating should equal the desired trip-point voltage minus the 0.7V base-emitter drop.

In the dc detector circuit shown in Fig 7b, when the unregulated dc voltage drops, a pnp transistor turns on and produces a positive pulse. Here, the zener diode's rating is equal to the trip-point voltage minus 5V, plus 0.7V for the base-emitter drop.

The circuit in Fig 7c trips when the dc level at R<sub>1</sub>'s and R<sub>2</sub>'s junction drops to the zener's voltage rating. You can provide either a positive or a negative interrupt signal, depending on the operational amplifier's input configuration.

To ensure that the regulator operates long enough to perform a reliable transfer to nonvolatile memory once a store pulse is sent, you need to use a large filter capacitor. The capacitance depends on the desired trip point, the lowest input voltage to the regulator, and the load. For example, a system with a 10-msec transfer time, a 300-mA load, a 15V trip point, and a minimum regulator input of 7V requires a 375- $\mu$ F capacitor; you can derive the capacitor's value from the equation  $i=Cdv/dt$ .

Once you've chosen a sensing point and a sensing circuit, the next step is to develop a subsystem that uses the power-status signal to generate save and



**Fig 8—This industrial controller's storage architecture** uses a NOVRAM as both the volatile and nonvolatile system storage elements.

---

---

*Monitoring the ac line in front of the main supply's power transformer gives you the fastest warning of a power loss.*

---

restore signals. These signals tell the storage subsystem to transfer data from RAM to nonvolatile memory during power loss and return data to RAM after power has been restored.

The type of system you design will depend largely on the type of nonvolatile storage that you plan to use with that system. For instance, you could use battery-backed RAM, or you could use a NOVRAM like the one used in the industrial controller shown in Fig 8. The industrial-controller design takes advantage of the nonvolatile RAM's ability to transfer data between RAM and EEPROM in a 10-msec single write cycle (see box, "NOVRAM architecture").

The nonvolatile RAM provides both the system storage (RAM portion) and the nonvolatile program storage (EEPROM portion) for power losses. The  $\mu$ P supplies a low-going TTL store signal (100-nsec min duration) to the nonvolatile RAM's store input. During the 10 msec that the nonvolatile RAM requires to complete its data transfer, you must keep the power supply's voltage within the specified operating toler-

ance. Once the system initiates a store cycle, the store cycle can't be terminated.

When the system loses power, the sensor sends a power-failure-detection interrupt to the  $\mu$ P. Once the processor acknowledges the interrupt, it branches to an interrupt routine that writes the current stack pointer and a test byte to the nonvolatile RAM (to signify that a power failure has occurred) and generates a store signal. The power supply holds  $V_{CC}$  above 4.5V for 10 msec after it generates the power-fail signal. During the store operation, the nonvolatile RAM I/O lines maintain high impedance, allowing the  $\mu$ P to complete other tasks. After the system completes a store operation, it must drive the store input high before performing subsequent store operations.

When power is restored, the power-on-reset routine sends a recall signal to the nonvolatile RAM. The routine in the  $\mu$ P then checks the nonvolatile RAM's test byte to see if the previous process had been interrupted by a power failure. If so, the processor saves the current processor state and loads the address

## NOVRAM architecture

A NOVRAM (nonvolatile RAM) is a memory device comprising a static RAM overlaid bit for bit with an EEPROM (electrically erasable programmable ROM). A typical nonvolatile RAM, the Xicor X2212, contains 2k bits organized as a conventional 1k-byte static RAM overlaid with a 1k-byte EEPROM.

The operation of the RAM portion is identical to that of other static RAMs. However, in addition to CS (chip select) and WE (write enable) pins, nonvolatile RAMs also have store and recall pins that control data transfers between the RAM and EEPROM. Because the pulse widths of the control and data inputs are less than 450 nsec, most  $\mu$ P-based systems don't require wait states during the data transfers.

A store operation transfers the entire RAM contents to the EEPROM in a single 10-msec write cycle. After the NOVRAM completes the store operation, the original data will reside in both the RAM and the EEPROM.

The NOVRAM uses a recall operation to transfer data in the EEPROM to the RAM, replacing the RAM's prior content. Instead of moving data on a word-by-word basis, store and recall operations transfer the entire content of the memory simultaneously.

NOVRAMs don't require high-voltage pulses or high-voltage supplies: The devices operate from a single 5V power source and have no battery backup. All inputs and outputs are TTL compatible. The RAM portion's

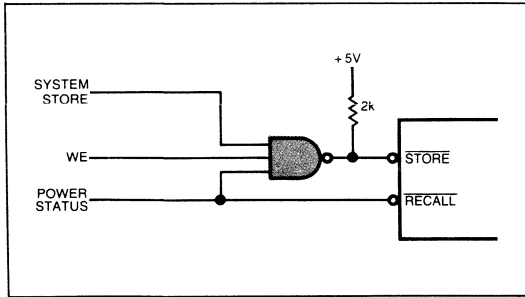
cycle time is 300 nsec, and the common data input/output is 4 bits wide.

### On-chip protection

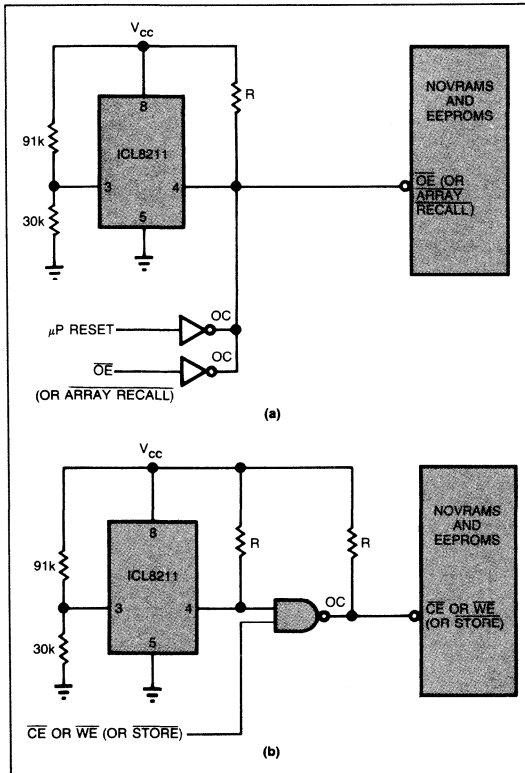
A built-in  $V_{CC}$  sensor protects the NOVRAM from spurious signals often initiated during power-up and power-down. The sensor establishes a threshold supply voltage of 3V. When the supply voltage falls below 3V, store operations to the EEPROM and write operations to the nonvolatile RAM are blocked.

A noise filter built into the EEPROM prevents glitches on the WE line from initiating a write cycle. This filter makes the device ignore pulses of less than 20 nsec so that noise spikes will not be interpreted as write commands.

*An alternative to monitoring ac power at the power transformer is monitoring the unregulated dc power to the regulator.*



**Fig 9**—By NANDing the store, WE, and power-status signals you can protect the NOVRAM from false store commands. In this configuration, all three inputs must be true for a store operation to occur.



**Fig 10**—In a hold-low protection scheme (a), a nonvolatile memory's array-recall pin is pulled to logical zero when the supply voltage falls below 5V. In hold-high protection (b), when power is lost, either the WE or CE pins are held high.

of the saved processor state onto the stack. It then executes a return from interrupt and resumes the previously interrupted process.

### Beware false commands

One of the biggest obstacles you'll face in deriving reliable store and save signals will be to avoid false store commands. Because most  $\mu$ P-based systems don't operate in ideal environments, they often generate false signals during power-ups, power-downs, brown-outs, and power failures. However, these signals are generally nonperiodic in nature, so the system usually recognizes them as by-products of a faulty memory device and disregards them.

Sometimes, however, these signals are periodic and turn out to be unintended write/store commands. After a system reset, for example, the  $\mu$ P's erratic behavior may cause the registers that usually contain the system information to contain false write-store commands instead. Therefore, when the system addresses those registers, those registers issue a false store command.

You can use several system techniques to avoid these errant commands. (For a discussion of on-chip protection features, see box, "NOVRAM architecture.") One technique for protecting the NOVRAM from errant commands takes advantage of the fact that even though most  $\mu$ P's can issue spurious addresses, they don't usually issue false write commands. By ANDing the system write command with the system store command, you can make sure that the nonvolatile RAM will respond to a store signal only during a write cycle.

Nevertheless, glitches can still appear at the store pin during power up, even if no write command is received at any of the 3-state TTL gate inputs. One way to solve this problem is to use an open-collector NAND gate, one of whose inputs indicates the power supply's status (Fig 9). This method ensures that the store pin's voltage follows the power supply's voltage as the voltage increases.

If you hold one NAND gate's open-collector input low, the output transistor is turned off. Pulling the gate's output voltage to the nonvolatile RAM's power supply through a pullup resistor ensures that the output follows the power supply with no glitches. You can also use the power supply's status signal to hold the recall pin low and the store pin high. This technique gives you better control over the nonvolatile RAM because it uses two conditions to prevent an inadvertent store operation. All you need to do is to connect the status signal directly to the recall pin.

Two additional methods of preventing unintentional nonvolatile data changes during power transitions are hold-low and hold-high protection. When you use hold-low protection (Fig 10a), the array recall pin is pulled to logical zero whenever the supply voltage falls below the 5V-10% threshold. The Intersil ICL8211, an 8-pin miniature DIP, provides the voltage reference and gives a zero output whenever the supply falls below its threshold. When the sensed voltage rises above the selected threshold, the device produces a logical one.

(Fig 10b) gives an example of hold-high protection. ICL8211 keeps the voltage on the nonvolatile RAM's store pin (or the  $\overline{WE}$  or  $\overline{CE}$  pins) near the power supply's voltage level. This blocks the low pin voltage that's necessary for a write or store operation.

The power-supply output that ICL8211 senses is a sawtooth waveform. ICL8211's output is a logical 1 while the supply output is above 4.5 volts. Below 3V, the nonvolatile RAM's internal protection circuitry prevents inadvertent writes or stores. In the critical unprotected range between 3 and 4.5V, ICL8211 provides a zero output to prevent writes or stores.

An alternative to ICL8211 in these applications is the SGS L487. The SGS L487 is a 500-mA precision 5V voltage regulator that includes an open-collector power-on/power-off reset output pin that protects nonvolatile memory the same way the ICL8211 does.

Other schemes that protect systems from inadvertent store operations employ jumpers, cables, and switches. You transmit the store signal through a jumper or switch that you hold open unless you're changing data in the EEPROM. During normal operation, the only component attached to the store pin is a resistor to the power supply. **EDN**

---

### Author's biography

*Christopher Lopes is an applications engineer at Xicor (Milpitas, CA), where his duties include system-level evaluation, product-application development, and customer technical assistance. A member of the IEEE, Chris holds a BS in electrical and electronic engineering from California State University at Sacramento and is currently enrolled in the MBA program at the University of Santa Clara. He enjoys windsurfing, skiing, and tennis.*

---

Reprinted from **EDN** February 21, 1985  
© 1985 CAHNERS PUBLISHING COMPANY



REPRINTED FROM

A MCGRAW-HILL PUBLICATION

# Electronics®

---

**THICK OXIDE BEATS THIN FILM  
IN BUILDING BIG EEPROMS**

7

## INSIDE TECHNOLOGY

THICK OXIDE BEATS THIN FILM  
IN BUILDING BIG EEPROMS

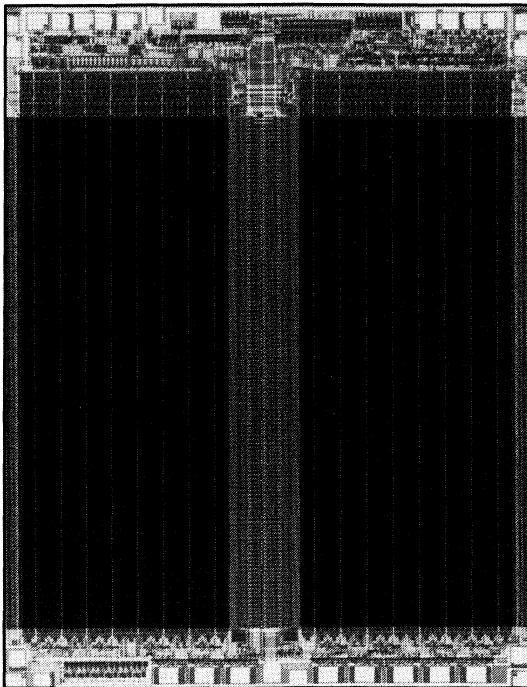
## XICOR USES IT TO SOLVE 3-D SCALING PROBLEMS IN 256-K CHIPS

**B**y abandoning the conventional thin-film route to fabricating high-density electrically erasable programmable read-only memories, Xicor Inc. may have overcome the problems that have kept the parts from climbing above the 64-K density level. The Milpitas, Calif., company employed a conservative 2- $\mu\text{m}$  process and standard off-the-shelf 5 $\times$  stepper lithographic equipment to build a 256-K EEPROM.

The key to doing this was the use of a thick oxide and a unique triple-polysilicon floating-gate cell, says William Owen, Xicor's vice president of research and development. The process is inherently more reliable and easier to scale to sub-micron dimensions, he claims, although it was more difficult for the Xicor engineers to master. They were less familiar with it than with the thin-oxide double-poly technology derived from EPROM manufacture.

Conventionally used thin-oxide floating gates are relatively easy to manufacture, but cannot be scaled down easily without introducing significant reliability problems. This unpleasant consequence of the laws of physics is one reason many EEPROM houses are having difficulty moving to densities beyond 64-K to the 256-K level. To do so requires pushing minimum line widths on the oxides down to 1  $\mu\text{m}$  using advanced photolithography.

"The problem with scaling EEPROMs lies in the fact that it is necessary to scale in three dimensions—in the vertical as well as horizontal directions," says Owen. "To achieve 256-K densities, not only must thin-oxide EEPROMs be scaled from 2 or 3  $\mu\text{m}$  down to 1 to 1.5  $\mu\text{m}$  in the horizontal direction, but from 90 to 100  $\text{\AA}$  down to about 70 to 80  $\text{\AA}$  in the vertical direction." To achieve similar densities in its 256-K EEPROM, Xicor found it necessary only to scale down from 3 to 2  $\mu\text{m}$



**1. SMALL DIE.** Equivalent in size to many thin-oxide 64-K parts, Xicor's 256-K EEPROM die measures about 64,000 mils<sup>2</sup>.

horizontally and from 600 to 800  $\text{\AA}$  down to 400  $\text{\AA}$  vertically.

The thick oxide enabled Xicor's designers to form a basic EEPROM cell with a triple-poly structure that puts the programming portion atop the erase mechanism. This resulted in horizontal cell dimensions smaller than the thin-oxide structure.

Another factor in the smaller size was the use of a proprietary textured thick-oxide surface on the programming elements. The textured surface's electrical potential per unit area is greater than conventionally used smooth surfaces, producing cells that are inherently smaller than comparable thin-oxide cells, but with the same effect. The oxide can be shaved off without affecting cell reliability, making vertical scaling relatively easy.

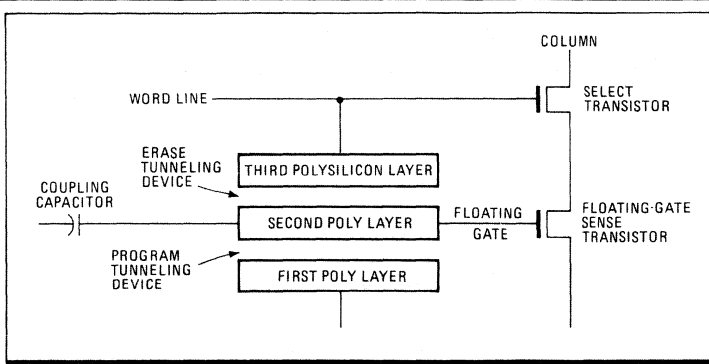
The first 256-K EEPROM fabricated with the 2- $\mu\text{m}$  process is the 32-K-by-8-bit n-MOS X28256. It features a chip area of about 64,000 mils<sup>2</sup> (Fig. 1), equal in size to many thin-oxide 64-K parts fabricated using 1.5- $\mu\text{m}$  design rules, and half the size of thin-oxide 256-K EE-

PROMs designed with 1- to 1.2- $\mu\text{m}$  geometries. Soon to follow will be a CMOS version, the X28C256. Both parts feature 150-ns access times and support 64-byte page-write operations. A write cycle takes 31  $\mu\text{s}$  per byte, enabling the entire memory to be written in less than 1 second.

In Xicor's triple-poly cell (Fig. 2), the floating gate sits between the upper and lower poly layers, forming the thick-oxide tunnel structures for erasure and programming. Compared with the 80- to 120- $\mu\text{m}^2$  cells of conventional 1- $\mu\text{m}$  thin-oxide designs, the electrically erasable cell in Xicor's 2- $\mu\text{m}$  256-K parts measure only 68  $\mu\text{m}^2$ .

The programming tunnel mechanism occurs between the first and second floating-gate poly layers; the erase tunneling action occurs between the second and third (Fig. 3, left). As in the thin-oxide approach, a selection transistor isolates the selected cell on a column while a capacitor develops, through capacitive coupling, enough voltage across a tunneling device to make electrons tunnel on and off the floating gate. This voltage is sensed by a MOS transistor, whose gate is formed by the second poly layer.

*TECHNOLOGY TO WATCH is a regular feature of Electronics that provides readers with exclusive, in-depth reports on important technical innovations from companies around the world. It covers significant technology, processes, and developments incorporated in major new products.*



**2. TRIPLE POLY.** Key to the small die area is a unique triple-poly floating-gate cell. The gate, between the upper and lower poly layers, performs erasure and programming.

Because capacitance increases linearly as oxide thickness decreases, tunnel devices made with very thin oxides—80 to 100 Å thick—rate 5 to 10 times higher than tunnel devices made with 500- to 800-Å-thick oxides. Consequently, cells using thin oxide have to push photolithography requirements to the limit of available equipment and processes in order to make the thin-oxide tunneling devices as small as possible. The coupling capacitor, which must be made from a thicker, nontunneling oxide, ends up relatively large to obtain efficient coupling.

In contrast, thick-oxide tunnel devices inherently have very low capacitance. Therefore they can be made with reasonable feature sizes and still produce a small cell with good coupling-capacitor efficiency. Since the feature sizes used in the tunnel devices are compatible with the lithography requirements of the rest of the cell, they can be readily scaled down as advances in lithography technologies become available for manufacturing.

What makes this structure work is its surface, which Xicor describes as textured with hillocks (Fig. 3, right). Also called asperities, these odd-looking features were at first considered an undesirable side effect of MOS processing, and occur because oxidation progresses faster along some crystal directions than others. Because crystal orientation is random in deposited poly, there are points on the surface of an integrated circuit where oxide growth is enforced. The temperature of the oxide controls the size and shape of the hillocks.

Through the use of carefully designed and controlled fabri-

cation techniques, Xicor exploits this phenomenon to build EEPROM transistors using thicker silicon dioxide layers that can still discharge the floating gate. Because the oxidation is a well controlled step, the properties of the emitters are exceptionally regular. They are shaped so that the electric field increases at the crest of the hills, substantially enhancing the emission of electrons.

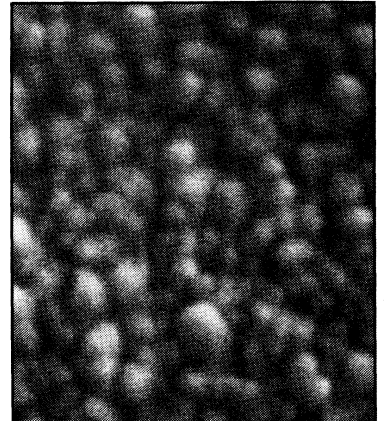
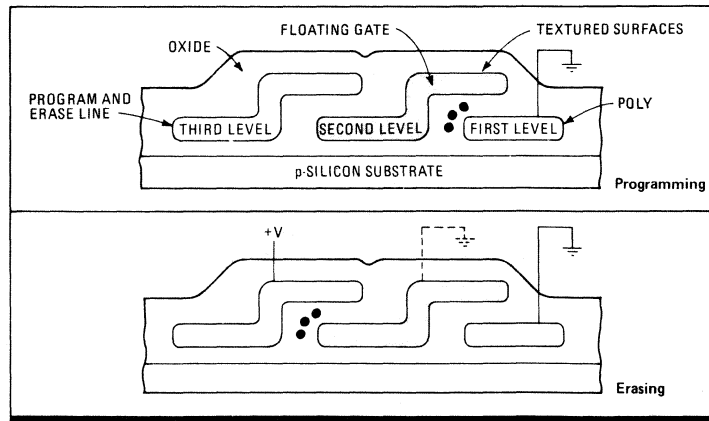
The poly electrodes are separated by oxide layers about 500 to 800 Å thick. Without the hillocks, Xicor says, 100 V would need to be applied to produce effective tunnel current. With the textured surfaces, the voltage required for tunneling is only 10 to 20 V, low enough to be generated easily on chip with an internal charge-pump circuit.

The coupling capacitor's size also contributes to the smaller cell area. To induce tunneling, the floating-gate voltage is raised or lowered through capacitive coupling to a bias-voltage supply. To avoid excessively high bias voltages, efficient coupling to the floating gate must be achieved by making the coupling capacitance much higher than all other floating-gate capacitances combined. These other capacitances include that of the MOS sense transistor, and especially that of the tunnel devices.

To electrically program a cell, electrons must tunnel onto the floating gate. In Xicor's triple-poly enhanced-emission cell, this is accomplished by applying a bias voltage to the coupling capacitor to capacitively pull the floating gate high and develop a voltage across the program tunneling device. When this voltage reaches the tunnel voltage, electrons tunnel from the first poly level's surface through the programming device to the second-level floating gate. When the applied voltages are brought back to normal reading levels, the programmed floating gate carries a negative voltage because of the extra electrons on it. When read, the MOS floating-gate sense transistor is turned off by the negative voltage and a 0 is produced at the EEPROM's output.

To electrically erase a cell, electrons must tunnel off the floating gate. In Xicor's triple-poly cell, this is done by capacitively coupling the second poly level's floating gate low while the third poly level's word line, which forms the other end of the erase tunneling device, is brought high. When the voltage across the erase tunneling device reaches the tunnel voltage,

**3. TUNNELS AND TEXTURE.** In Xicor's cell design, programming by tunneling action occurs between layers 1 and 2 and erasure between layers 2 and 3 (left). The thick-oxide cell approach uses a "textured" floating gate surface to enhance electron emission.



electrons tunnel from the second poly floating gate to the third poly word line. When the applied voltages are brought back to normal reading levels, this erased floating gate has a net positive voltage because of the lack of electrons on its surface. When read, the MOS floating-gate sense transistor is turned on by this positive voltage and a 1 is produced at the EEPROM's output.

Other advantages of the thick-oxide approach, says Owen, include improved data retention and endurance, or the number of data changes a nonvolatile memory can sustain before the first bit fails. Because the floating gates in the Xicor design are completely surrounded by thick thermal oxides, similar to an EPROM, data retention is excellent even at very high temperatures. "In fact, the only way retention can be measured on the thick-oxide devices is by subjecting them to temperatures over 300°C for several weeks," Owen says. "If these measurements are extrapolated, the typical retention for a Xicor EEPROM is more than 2 million years at 125°C." But for the record, the company is much more conservative, guaranteeing data retention of only 100 years at 125°C.

The data-retention advantages of the textured thick-oxide approach are retained—or even improved—as devices are scaled, he says. This is due to the fact that lower programming voltages are needed in order to scale the memory properly, so isolation widths and device channel lengths can be reduced in both the memory array and in the peripheral circuitry. However, for a typical part, which stores data in 3 ms and must retain it for 10 years, the tunneling current under storage and reading conditions must be reduced by at least  $10^{11}$  than under programming conditions because the retention time is  $10^{11}$  times longer than the storage time.

For planar nontextured tunneling structures, this is a difficult design constraint because the slope of the current-voltage curve—that is, the relationship between the current and voltage of the tunneling device—is fixed. This means that the maximum allowable read voltage drops with the programming voltage on a volt-for-volt basis, not proportionately.

On the other hand, a textured-surface tunneling structure has a much steeper current-voltage curve; that is, for each increment of change in one voltage, there is an amplified increment of change in the other. In addition, the curve is not fixed, which means the relationship between the current and voltage can be tailored to yield steeper curves if necessary. This means that for a given

maximum read voltage, a textured surface requires a lower programming voltage than a planar thin-oxide structure, leading to better scaling.

With regard to endurance, recent data on Xicor's EEPROMs indicates an expected failure-in-time rate of 0.015% per 1,000 hours, or 150 FIT, in systems requiring 10,000 data changes per byte over a 10-year period, says Owen. "Thus for many applications, the endurance-related fallout is actually similar to or lower than other semiconductor-related failure rates."

To achieve 1-Mb densities, Owen believes that although it will require moving to 1- $\mu$ m geometries horizontally, only a few "tens of angstroms" reduction will be necessary in the vertical direction. "In thin-oxide EEPROMs, this is a reduction of 10% to 15% down to the operational limits of the floating-gate mechanism," he says. By comparison, Xicor's thick-oxide approach requires a reduction on the order of a few percentage points. "Moreover, the scaling is well within the limits of the Xicor cell design," he says. "As a matter of fact, we think we can continue to scale for several generations before we run into any of the problems our competitors are running into with thin-oxide EEPROMs." □

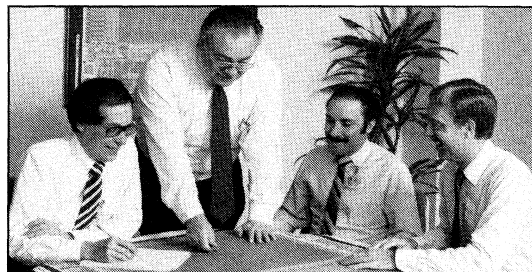
## XICOR: FROM LONG SHOT TO LEADER

**Life is sweet** these days for Raphael Klein, Julius Blank, William Owen III, and Wallace E. Tchon, who all helped found Xicor Inc. in 1978. But they can recall the time when the Milpitas, Calif., company's chance of survival was considered a long shot.

"The problem was that few in the industry thought we had a technological edge except us," says Owen, vice president of research and development. "There was Intel Corp., with its thin-oxide approach to fabricating electrically erasable programmable read-only memories, and there was Xicor, with the thick-oxide approach. Everybody seemed to be going the thin-oxide route." All that is changing now.

First of all, it is becoming clear that the company is at least a generation ahead of its competition with its thick-oxide approach. While everyone else is pushing to 1- $\mu$ m geometries to achieve 256-K products, Xicor is coasting along with a relatively conservative 2  $\mu$ m to achieve the same density.

Second, thin-oxide advocate Intel has entered into a long-term agreement with Xicor for joint development of advanced EEPROMs. The deal also calls for mutual second-sourcing of EEPROMs and related products. As part of the agreement with Intel, Xicor has received \$6.5 million and may receive an additional



**COMING UP ROSES.** The commitment to thick-oxide EEPROMs finally starts paying off for Xicor Inc.'s Tchon (left), Blank, Klein, and Owen.

\$500,000 as well as a \$10 million lease guarantee.

Third, the company continues to dominate the market it created, 5-V-only EEPROMs. Sales have grown from \$2.8 million in 1982 to \$39 million in 1984. Estimates for 1986 range as high as \$55 million.

Finally, Xicor had profitable operations during all four quarters of 1984 plus Q1 of 1985. It owns about 50% of the market for 5-V EEPROMs and Novrams, static random-access memories backed by nonvolatile EEPROM cells.

Klein, now chief financial officer and chairman of the board, is a graduate physicist from the Israeli Institute of Technology and performed in a variety of technical management positions at Fairchild, Intel, Monolithic Memories, and National Semiconductor before starting Xicor as its first president. He

holds two patents.

Owen, who joined the company to direct its development of advanced memories in 1978, holds an MS in electrical engineering and previously worked at Intel. As a process engineer and senior design manager, he was involved in the development and design of Intel's HMOS memory products.

Strategic planning vice president Tchon, who joined Xicor to aid in the development of its initial memories, is now principally involved in business planning, patent activity, and investor relations. With an MS in physics, Tchon holds 10 patents. Before Xicor, he held engineering positions at Honeywell Information Systems and Intel.

Blank, one of the original eight founders of Fairchild Semiconductor Corp. in 1957, has been a member of the Xicor board of directors since its founding.

# MACHINE DESIGN

A PENTON/IPC PUBLICATION

## TECH BRIEFS

# SOLID-STATE POTENTIOMETER

**RICHARD PALM**  
Applications Engineer  
Xicor Inc.  
Milpitas, CA

Potentiometers play a vital role in circuit design, yet they have a

number of problems. Their settings can change when exposed to vibration. They are difficult to use with automatic insertion and soldering equipment. And trimming must be done by hand.

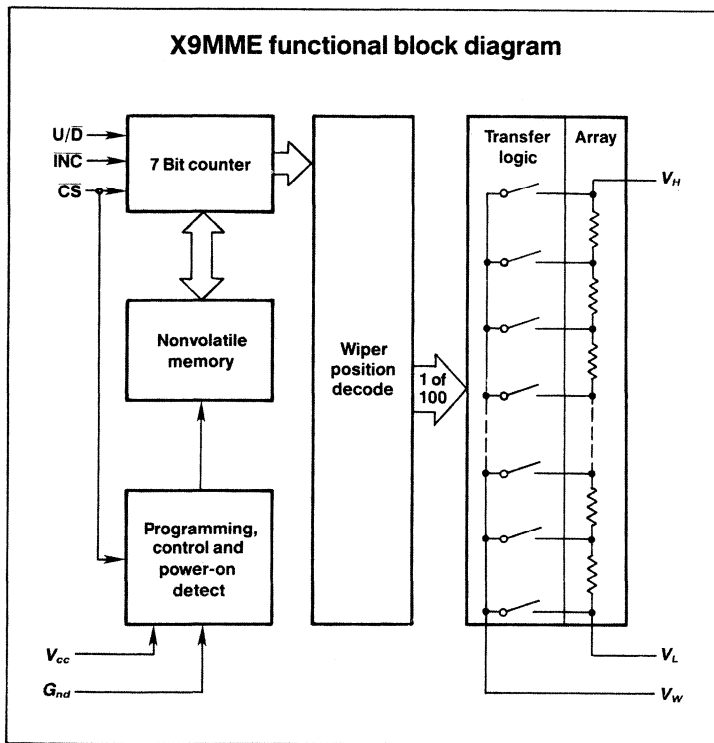
A solid state potentiometer solves these problems. Packaged in an eight-pin minidip, an electrically

erasable ( $E^2$ ) device called the X9MME digitally controls resistance trimming. The device has three-wire TTL control and operates from a standard 5-V power supply. Packaged in the dip is a 99-resistor array. Tap points are between the resistive elements and at the ends of the array. A tap point can be connected to the wiper output  $V_w$ .

Because the resistive elements are all equal, each has  $1/99$  the total resistance of the array. In a voltage divider application, moving the wiper up or down the array produces a linear output on  $V_w$ , with a resolution of 1%.

The tap point on the array is selected with three TTL inputs on the digital portion of the device. These inputs control a seven-bit up/down counter. To move the wiper tap point, the "chip select" line must be activated ( $CS = LOW$ ), the wiper direction selected ( $U/D$ , up = HIGH, down = LOW), and a clock pulse provided to the INC input. Counter output is decoded to select one of 100 tap points.

Mechanical potentiometers essentially have a nonvolatile memory; resistance does not change until the wiper is moved. In the X9MME, seven bits of nonvolatile  $E^2$  memory retain the resistance value. When the device is deselected after a wiper position change, the counter output is stored in memory. If power is re-



7

moved and subsequently restored, the nonvolatile memory contents are transferred to the counter and the last stored wiper position decoded. Wiper position retention is 100 years.

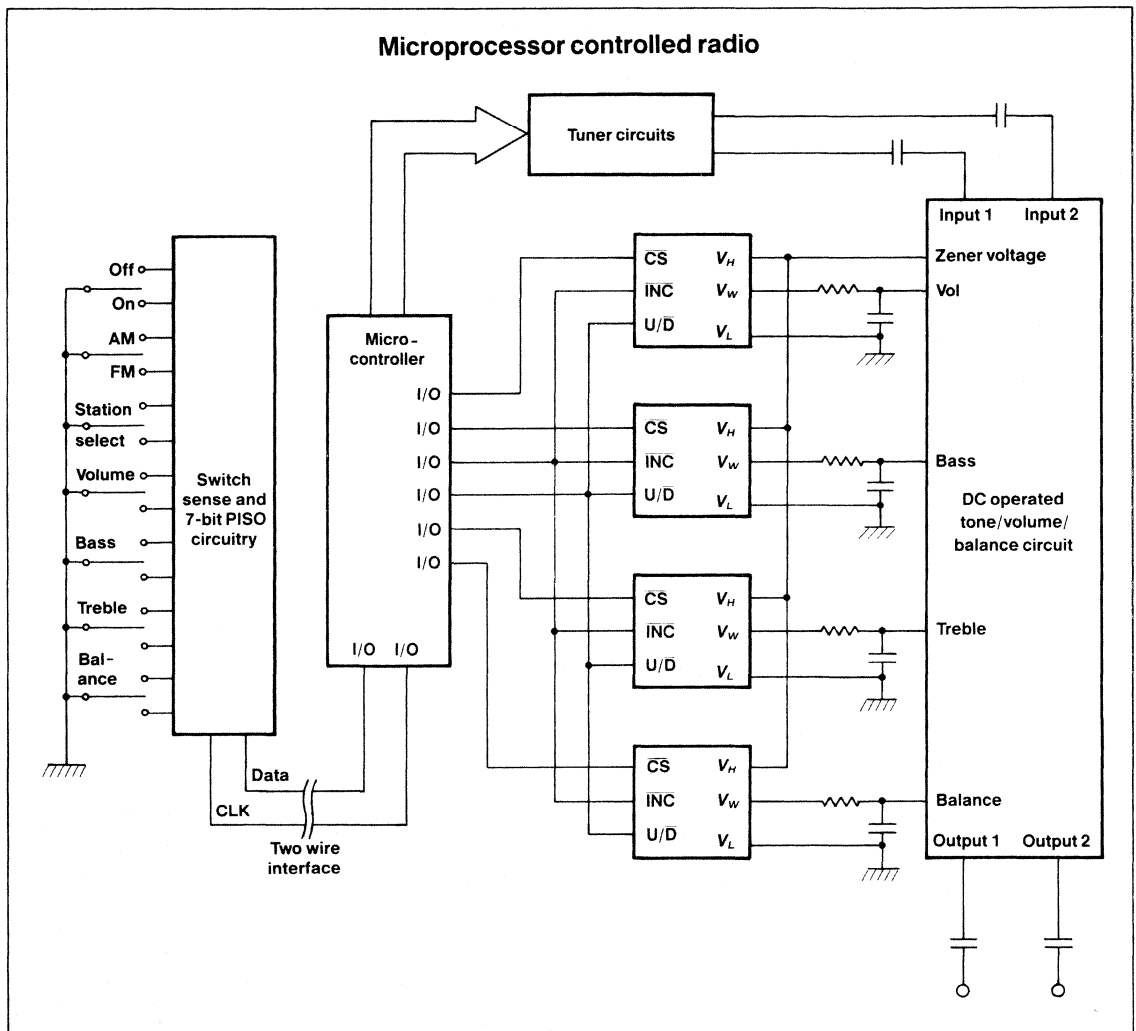
The manufacturing and test cost of equipment produced in high volumes can be reduced when solid state pots are used. Because automatic insertion equipment can be used, the device is soldered and cleaned just like other electronic components. This eliminates special handling and cleaning steps. During board testing, automatic

test equipment (ATE) can check the device and set wiper position. Hand operations are reduced, and the cost of supplemental test equipment is eliminated.

Operator convenience can also be of prime concern in circuit design. If the equipment operator or field technician must access the pot to make adjustments, the design process is complicated. The X9MME, in contrast, can be placed anywhere in the circuit and still be controlled through keyboards or a microprocessor.

As an example of how circuitry

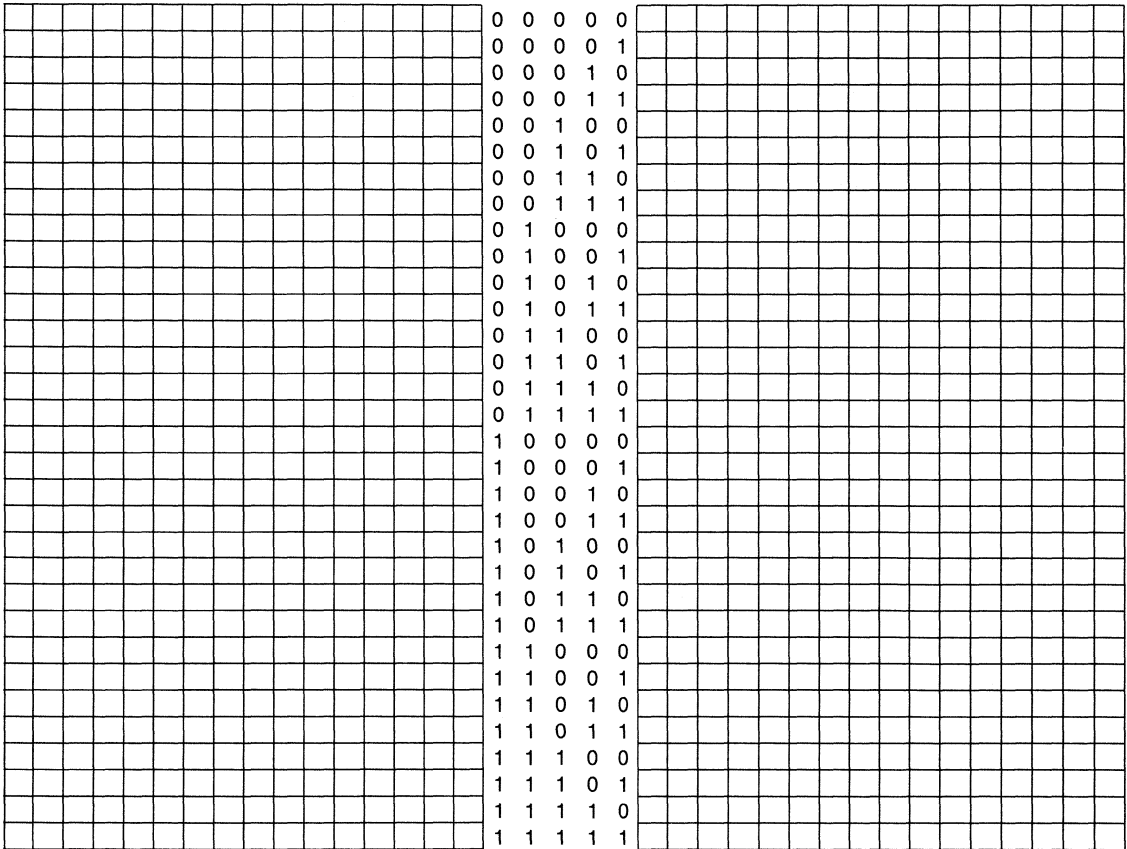
can be simplified, consider a hypothetical car radio system. Control might be by miniature rocker switches mounted on the steering wheel. The switch sense and 7-bit parallel-in-serial-out circuit could be implemented in either discrete TTL circuits or as a standard cell or programmable logic device. The microcontroller interface would be two wires, one for the shift clock and another for the interrupt and data transfer. The microcontroller actuates off/on, AM/FM selection, and tuning. Six port lines control volume, bass, treble and balance. ■



**Nonvolatile Static RAM**

On the following pages are individual device bit maps. These bit maps are supplied to aid in the development of test programs.

X<sub>4</sub> X<sub>3</sub> X<sub>2</sub> X<sub>1</sub> X<sub>0</sub>  
 A<sub>0</sub> A<sub>1</sub> A<sub>2</sub> A<sub>6</sub> A<sub>5</sub>



0 1 0 1 0 1 0 1 0 1 0 1 0 1 0 1  
 0 0 1 1 0 0 1 1 0 0 1 1 0 0 1 1  
 0 0 0 0 1 1 1 1 0 0 0 0 1 1 1 1  
 0 0 0 0 0 0 0 0 1 1 1 1 1 1 1 1  
 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0

Y<sub>0</sub> = A<sub>8</sub>  
 Y<sub>1</sub> = A<sub>4</sub>  
 Y<sub>2</sub> = A<sub>7</sub>  
 Y<sub>3</sub> = A<sub>3</sub>  
 Y<sub>4</sub> = A<sub>9</sub>

0 1 0 1 0 1 0 1 0 1 0 1 0 1 0 1  
 0 0 1 1 0 0 1 1 0 0 1 1 0 0 1 1  
 0 0 0 0 1 1 1 1 0 0 0 0 1 1 1 1  
 0 0 0 0 0 0 0 0 1 1 1 1 1 1 1 1  
 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1

Each Square Equals One Bit.

Address to XY Key

A <sub>9</sub>	A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
Y <sub>4</sub>	Y <sub>0</sub>	Y <sub>2</sub>	X <sub>1</sub>	X <sub>0</sub>	Y <sub>1</sub>	Y <sub>3</sub>	X <sub>2</sub>	X <sub>3</sub>	X <sub>4</sub>

---

**256 Bit****X2210 Product Bit Map****64 x 4 Bit**

---

**Nonvolatile Static RAM**

---

I/O														X <sub>2</sub>	X <sub>1</sub>	X <sub>0</sub>	I/O																	
1	2	1	2	1	2	1	2	1	2	1	2	1	2	1	2	A <sub>4</sub>	A <sub>3</sub>	A <sub>5</sub>	3	4	3	4	3	4	3	4	3	4	3	4	3	4	3	4
																0	0	0																
																0	0	1																
																0	1	0																
																0	1	1																
																1	0	0																
																1	0	1																
																1	1	0																
																1	1	1																
1	0	1	0	1	0	1	0	1	0	1	0	1	0	0	Y <sub>0</sub> = A <sub>2</sub>	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	0	0	
1	1	0	0	1	1	0	0	1	1	0	0	0	0	Y <sub>1</sub> = A <sub>1</sub>	1	1	0	0	1	1	0	0	1	1	0	0	1	1	0	0	0	0	0	
1	1	1	1	0	0	0	0	0	0	0	0	0	0	Y <sub>2</sub> = A <sub>0</sub>	1	1	1	1	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	

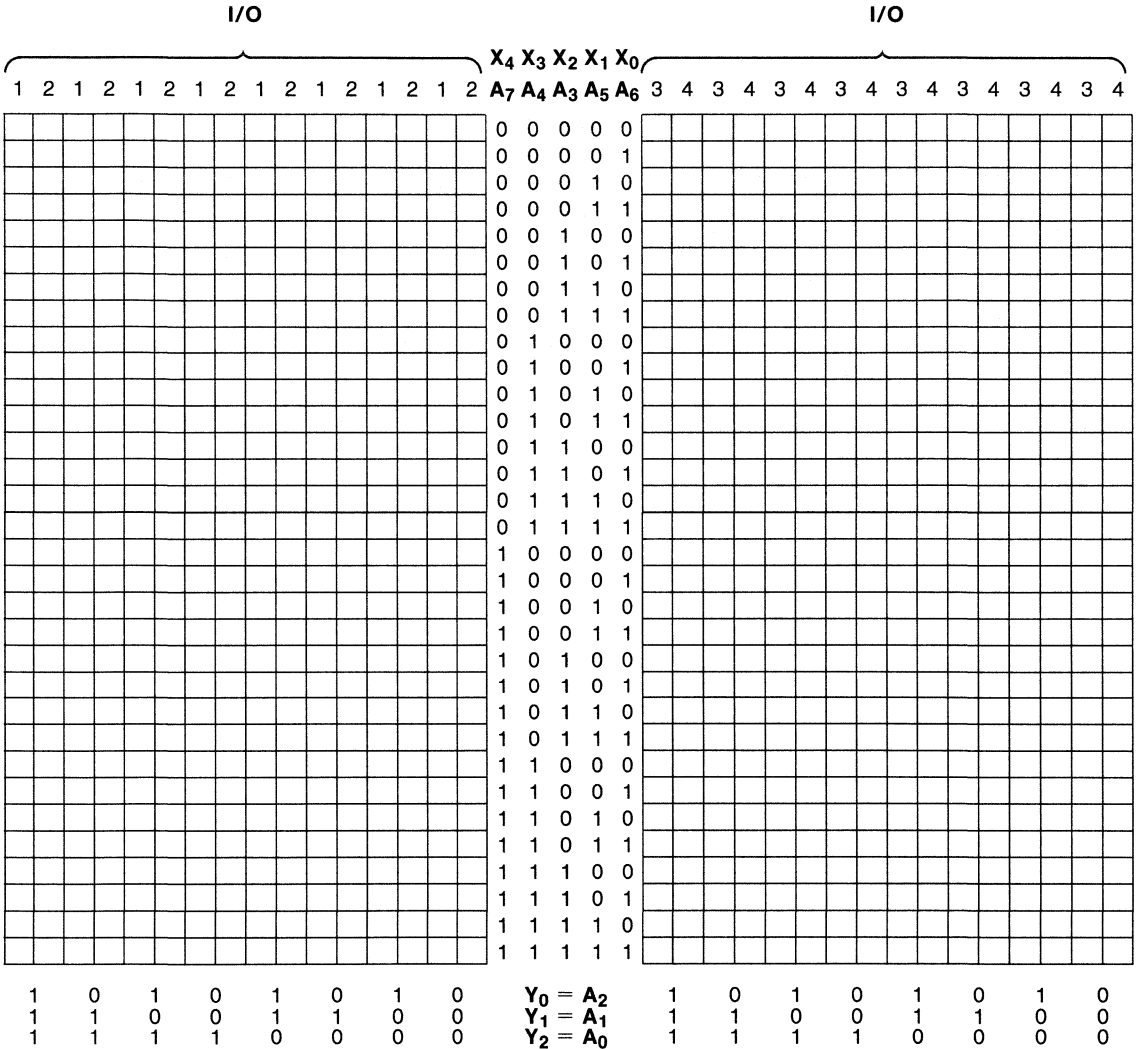
Each Square Equals One Bit.

Address to XY Key

A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>0</sub>	X <sub>2</sub>	X <sub>1</sub>	Y <sub>0</sub>	Y <sub>1</sub>	Y <sub>2</sub>



Nonvolatile Static RAM



Each Square Equals One Bit.

Address to XY Key

A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>4</sub>	X <sub>0</sub>	X <sub>1</sub>	X <sub>3</sub>	X <sub>2</sub>	Y <sub>0</sub>	Y <sub>1</sub>	Y <sub>2</sub>

1K

X2001 Product Bit Map

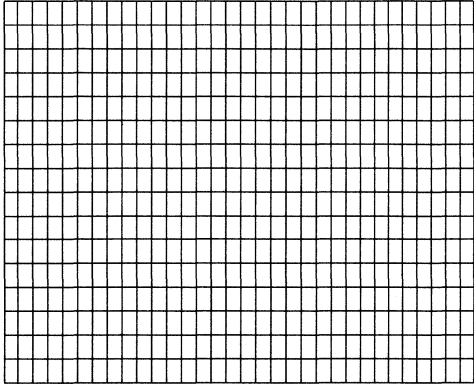
128 x 8 Bit

Nonvolatile Static RAM

I/O

I/O

0 1 0 1 0 1 0 1 0 1 0 1 0 1 0 1 2 3 2 3 2 3 2 3 2 3 2 3



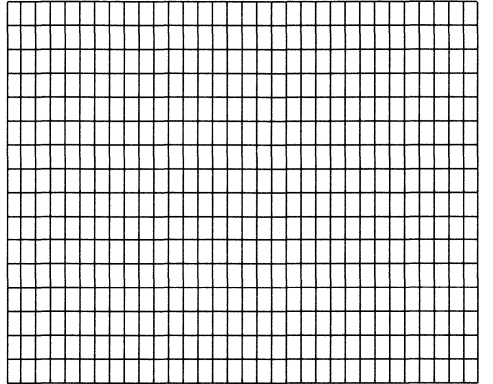
X<sub>3</sub> X<sub>2</sub> X<sub>1</sub> X<sub>0</sub>  
 A<sub>6</sub> A<sub>5</sub> A<sub>4</sub> A<sub>3</sub>

0 0 0 0  
 0 0 0 1  
 0 0 1 0  
 0 0 1 1  
 0 1 0 0  
 0 1 0 1  
 0 1 1 0  
 0 1 1 1  
 1 0 0 0  
 1 0 0 1  
 1 0 1 0  
 1 0 1 1  
 1 1 0 0  
 1 1 0 1  
 1 1 1 0  
 1 1 1 1

0 1 0 1 0 1 0 1 0 1 0 1 0 1 0 1  
 0 0 1 1 0 0 1 1 0 0 1 1 0 0 1 1  
 0 0 0 0 1 1 1 1 0 0 0 0 1 1 1 1

Y<sub>0</sub> = A<sub>1</sub>  
 Y<sub>1</sub> = A<sub>2</sub>  
 Y<sub>2</sub> = A<sub>0</sub>

5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 5 4 6 7 6 7 6 7 6 7 6 7 6 7 6 7 6 7 6 7 6 7 6 7



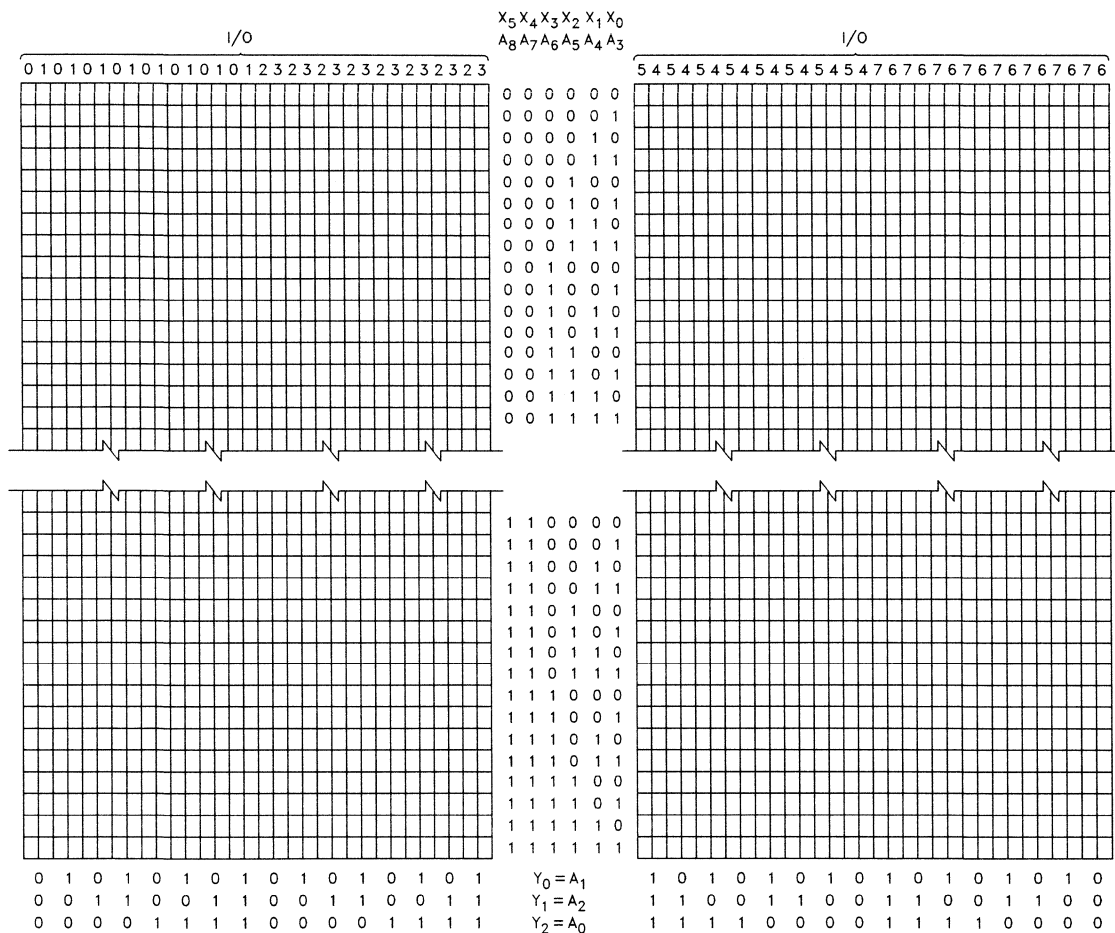
1 0 1 0 1 0 1 0 1 0 1 0 1 0 1 0  
 1 1 0 0 1 1 0 0 1 1 0 0 1 1 0 0  
 1 1 1 1 0 0 0 0 1 1 1 1 0 0 0 0

Each Square Equals One Bit.

Address to XY Key

A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>3</sub>	X <sub>2</sub>	X <sub>1</sub>	X <sub>0</sub>	Y <sub>1</sub>	Y <sub>0</sub>	Y <sub>2</sub>

Nonvolatile Static RAM



0025-8

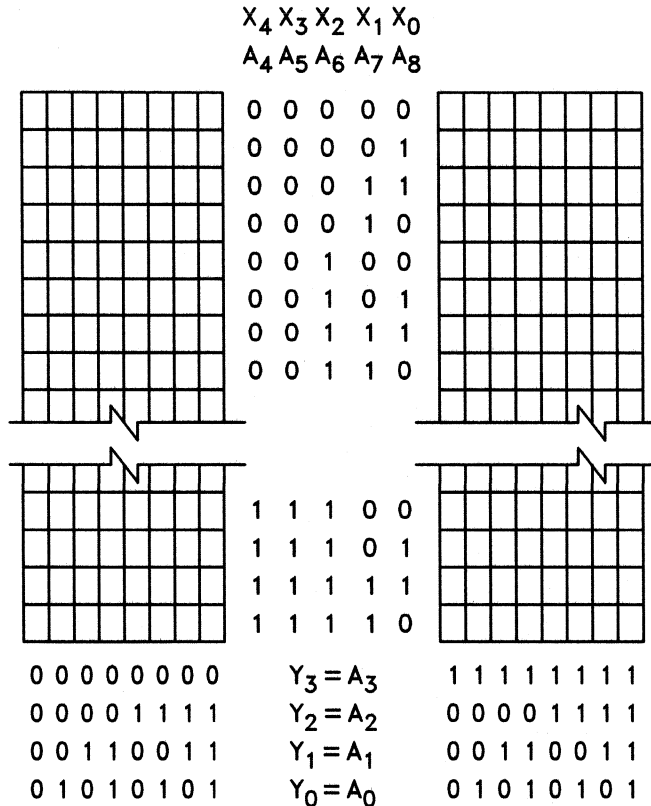
Each Square Equals One Bit.

Address to XY Key

A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>5</sub>	X <sub>4</sub>	X <sub>3</sub>	X <sub>2</sub>	X <sub>1</sub>	X <sub>0</sub>	Y <sub>1</sub>	Y <sub>0</sub>	Y <sub>2</sub>



Electrically Erasable PROM



0025-2

Each Square Equals One Byte.

Byte Map

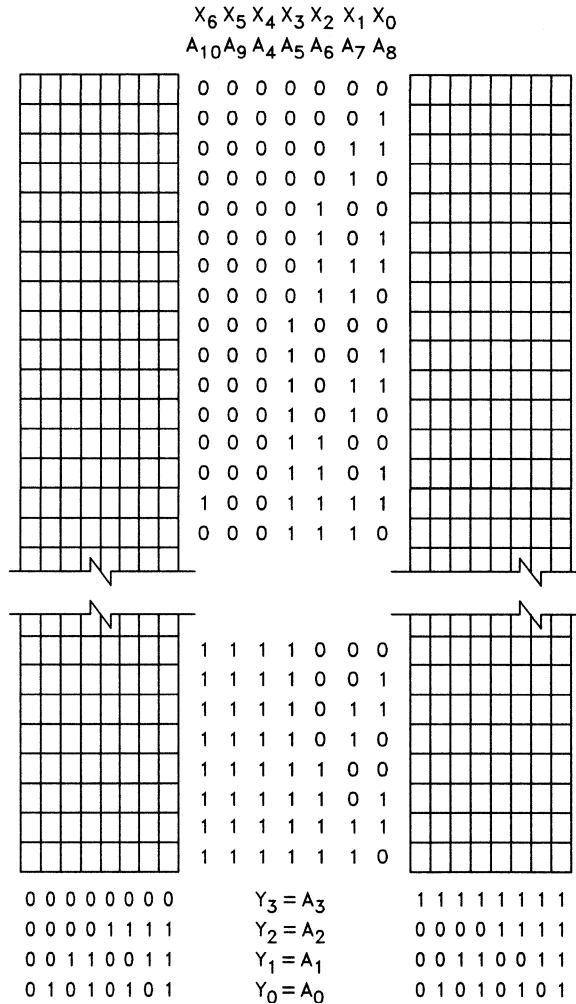
I/O <sub>0</sub>	I/O <sub>1</sub>	I/O <sub>2</sub>	I/O <sub>3</sub>	I/O <sub>4</sub>	I/O <sub>5</sub>	I/O <sub>6</sub>	I/O <sub>7</sub>
------------------	------------------	------------------	------------------	------------------	------------------	------------------	------------------

Address to XY Key

A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>0</sub>	X <sub>1</sub>	X <sub>2</sub>	X <sub>3</sub>	X <sub>4</sub>	Y <sub>3</sub>	Y <sub>2</sub>	Y <sub>1</sub>	Y <sub>0</sub>



Electrically Erasable PROM



0025-3

Each Square Equals One Byte.

Byte Map

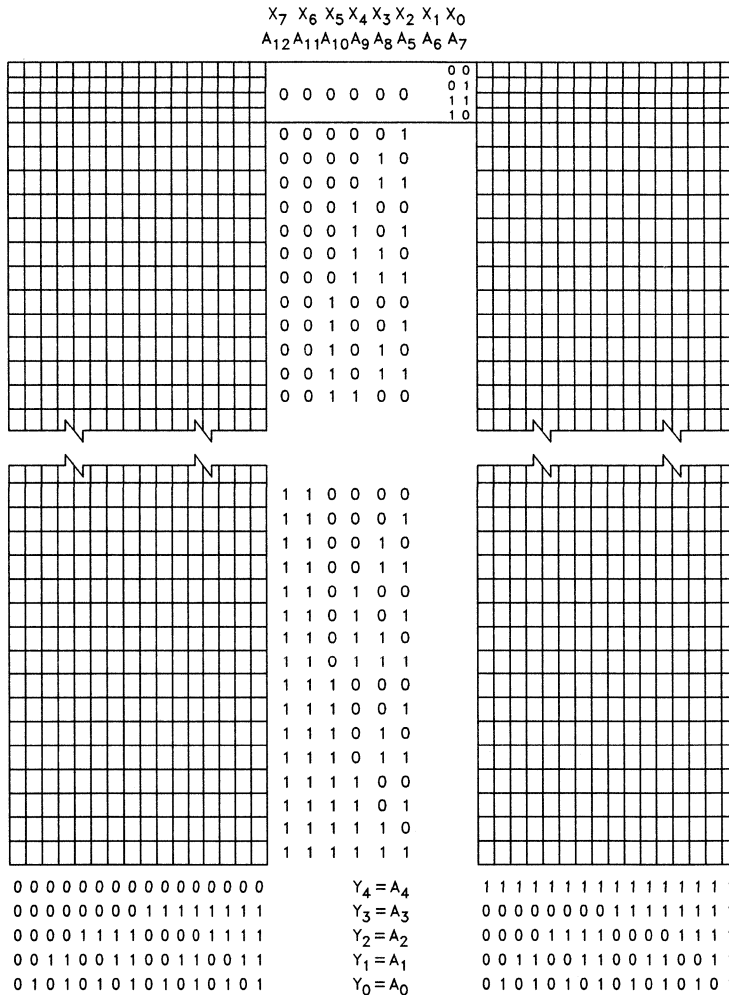
I/O <sub>0</sub>	I/O <sub>1</sub>	I/O <sub>2</sub>	I/O <sub>3</sub>	I/O <sub>4</sub>	I/O <sub>5</sub>	I/O <sub>6</sub>	I/O <sub>7</sub>
------------------	------------------	------------------	------------------	------------------	------------------	------------------	------------------

Address to XY Key

A <sub>10</sub>	A <sub>9</sub>	A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>6</sub>	X <sub>5</sub>	X <sub>0</sub>	X <sub>1</sub>	X <sub>2</sub>	X <sub>3</sub>	X <sub>4</sub>	Y <sub>3</sub>	Y <sub>2</sub>	Y <sub>1</sub>	Y <sub>0</sub>



Electrically Erasable PROM



0025-5

Each Square Equals One Byte.

Byte Map

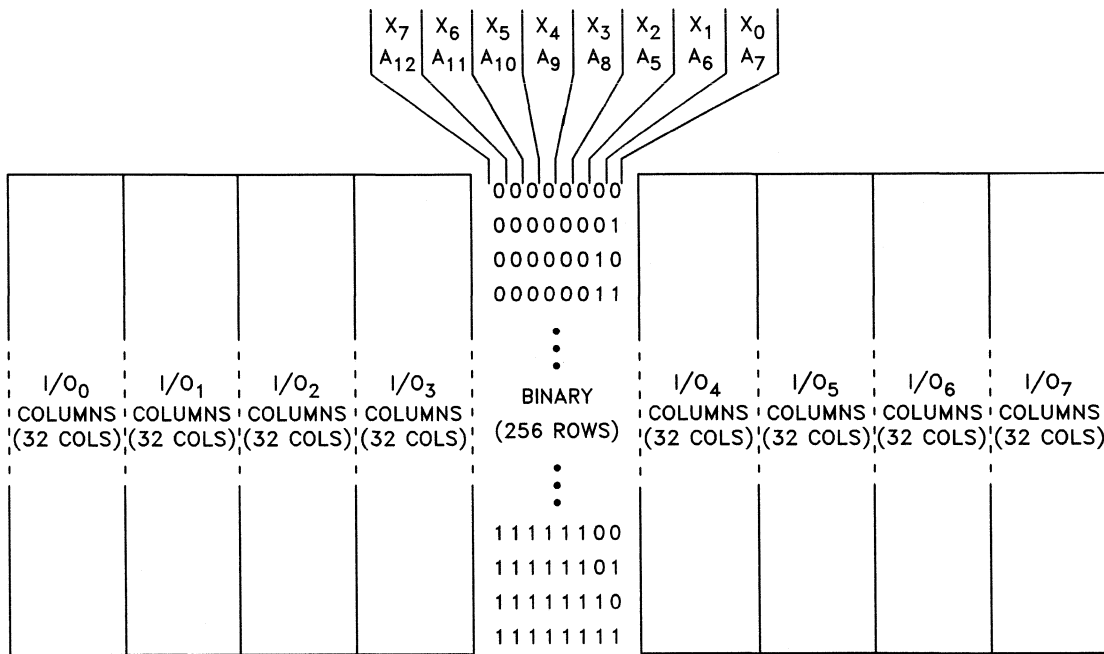
I/O <sub>0</sub>	I/O <sub>1</sub>	I/O <sub>2</sub>	I/O <sub>3</sub>	I/O <sub>4</sub>	I/O <sub>5</sub>	I/O <sub>6</sub>	I/O <sub>7</sub>
------------------	------------------	------------------	------------------	------------------	------------------	------------------	------------------

Address to XY Key

A <sub>12</sub>	A <sub>11</sub>	A <sub>10</sub>	A <sub>9</sub>	A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>7</sub>	X <sub>6</sub>	X <sub>5</sub>	X <sub>4</sub>	X <sub>3</sub>	X <sub>0</sub>	X <sub>1</sub>	X <sub>2</sub>	Y <sub>4</sub>	Y <sub>3</sub>	Y <sub>2</sub>	Y <sub>1</sub>	Y <sub>0</sub>



Electrically Erasable PROM



Y <sub>4</sub> = A <sub>4</sub>	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	0	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	1	
Y <sub>3</sub> = A <sub>3</sub>	0	0	0	0	0	0	0	0	1	1	1	1	1	1	1	1	0	0	0	0	0	0	0	0	0	0	1	1	1	1	1	1	1	1	1	1	1
Y <sub>2</sub> = A <sub>2</sub>	1	1	1	1	0	0	0	0	0	0	0	0	0	1	1	1	1	1	1	1	0	0	0	0	0	0	0	0	1	1	1	1	1	1	1	1	1
Y <sub>1</sub> = A <sub>1</sub>	1	1	0	0	1	1	0	0	0	0	0	1	1	0	0	1	1	1	0	0	1	1	0	0	1	1	0	0	0	0	1	1	0	0	1	1	1
Y <sub>0</sub> = A <sub>0</sub>	1	0	1	0	1	0	1	0	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	0	1	

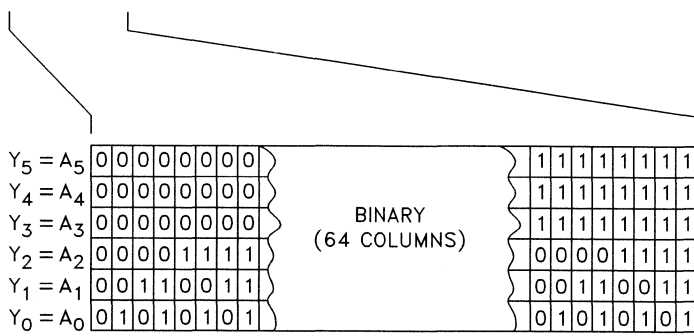
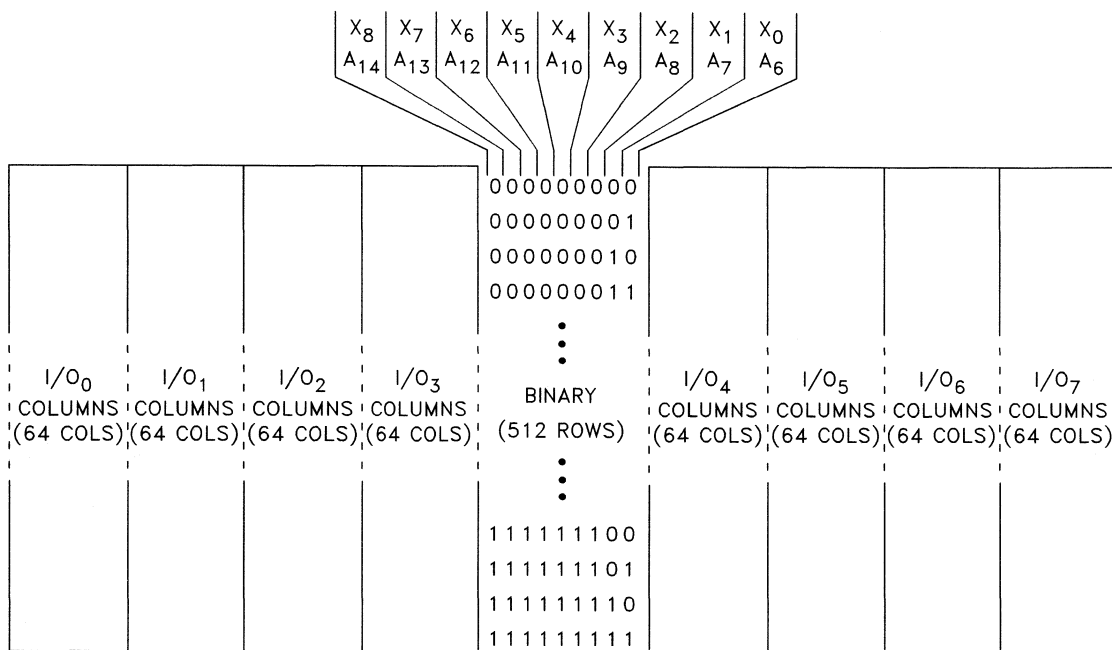


0025-6

Address to XY Key

A <sub>12</sub>	A <sub>11</sub>	A <sub>10</sub>	A <sub>9</sub>	A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>7</sub>	X <sub>6</sub>	X <sub>5</sub>	X <sub>4</sub>	X <sub>3</sub>	X <sub>0</sub>	X <sub>1</sub>	X <sub>2</sub>	Y <sub>4</sub>	Y <sub>3</sub>	Y <sub>2</sub>	Y <sub>1</sub>	Y <sub>0</sub>

Electrically Erasable PROM



0025-7

Address to XY Key

A <sub>14</sub>	A <sub>13</sub>	A <sub>12</sub>	A <sub>11</sub>	A <sub>10</sub>	A <sub>9</sub>	A <sub>8</sub>	A <sub>7</sub>	A <sub>6</sub>	A <sub>5</sub>	A <sub>4</sub>	A <sub>3</sub>	A <sub>2</sub>	A <sub>1</sub>	A <sub>0</sub>
X <sub>8</sub>	X <sub>7</sub>	X <sub>6</sub>	X <sub>5</sub>	X <sub>4</sub>	X <sub>3</sub>	X <sub>2</sub>	X <sub>1</sub>	X <sub>0</sub>	Y <sub>5</sub>	Y <sub>4</sub>	Y <sub>3</sub>	Y <sub>2</sub>	Y <sub>1</sub>	Y <sub>0</sub>

RR-502A	NOVRAM* Reliability Report . . . . .	8-1
RR-504	Endurance of Xicor E <sup>2</sup> PROMs and NOVRAMs* . . . . .	8-23
RR-505	X2816A/X2804A Reliability Report . . . . .	8-33
RR-506	Byte-Wide NOVRAM* (X2001/ X2004) Reliability Report . . . . .	8-45
RR-507A	X2864A Reliability Report . . . . .	8-57
RR-508	X2404 Reliability Report . . . . .	8-71
RR-509	X2816B Reliability Report . . . . .	8-79
RR-510	Endurance of Nonvolatile Memories . . . . .	8-87
	Determining System Reliability from E <sup>2</sup> PROM Endurance Data . . . . .	8-93
	Radiation-Induced Soft Errors and Floating Gate Memories . . . . .	8-97
	Endurance Model for Textured Poly Floating Gate Memories . . . . .	8-103
	The Prediction of Textured Poly Floating Gate Memory Endurance . . . . .	8-109
	Comparison and Trends in Today's Dominant E <sup>2</sup> Technologies . . . . .	8-117
	New Ultra-High Density Textured Poly-Si Floating Gate E <sup>2</sup> PROM Cell . . . . .	8-123
	Reliability Comparison of Flotax and Textured Poly E <sup>2</sup> PROMs . . . . .	8-125

## NOVRAM\* Data Sheets

1

## Serial I/O Data Sheets

2

## E<sup>2</sup>PROM Data Sheets

3

## E<sup>2</sup>POT™ Digitally Controlled Potentiometer Data Sheets

4

## Die Products

5

## Military

6

## Applications

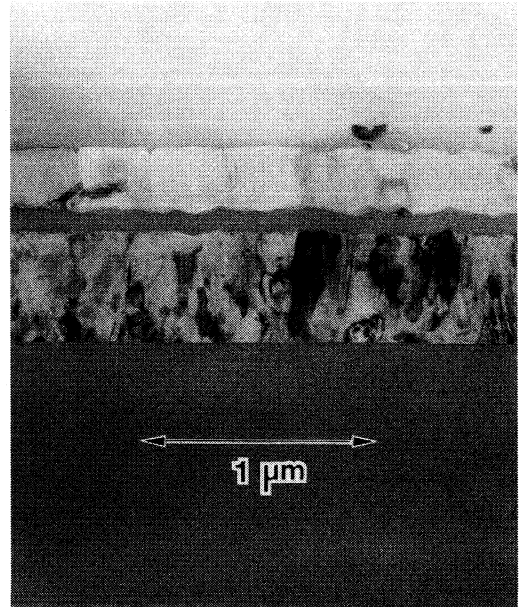
7

## Reliability

8







0075-1

# **NOVRAM\* RELIABILITY REPORT**

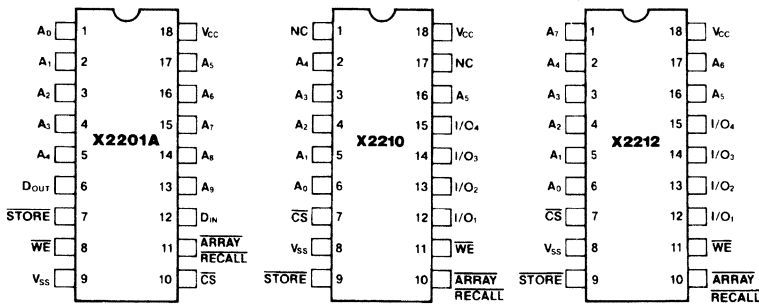
**By John Caywood  
and Reliability Engineering Staff**

\*NOVRAM is Xicor's nonvolatile static RAM device.

# INTRODUCTION

This report is an accumulation of reliability testing data taken on the Xicor X2210 and X2212 NOVRAM memories. In these memories, each memory bit integrates one bit of static RAM and one bit of electrically erasable-programmable ROM (E<sup>2</sup>PROM) into one cell. The controls STORE and RECALL cause the data to be transferred in parallel from all RAM bits into the associated E<sup>2</sup>PROM bits and back again. These devices, which exemplify

Xicor's innovative technology, require only a 5V power supply and TTL level signals for all operations, including STORE and RECALL. Both devices employ the same design and processes and are organized 64 x 4 and 256 x 4 for the X2210 and X2212, respectively. Figure 1 shows the pinout for the two parts, as well as for the X2201A (1K x 1) NOVRAM. Figure 2 shows the logic diagram. The bit maps for the three devices shown in Figures 3-5 illustrate the physical location of the various address bits.



## PIN NAMES

A <sub>0</sub> -A <sub>9</sub>	Address Inputs
I/O <sub>1</sub> -I/O <sub>4</sub>	Data Input/Output
WE	Write Enable
CS	Chip Select
ARRAY RECALL	Array Recall
STORE	Store
V <sub>CC</sub>	+ 5V
V <sub>SS</sub>	Ground
NC	No Connect

0075-2

Figure 1: X2201A, X2210, and X2212 pin assignment drawings.

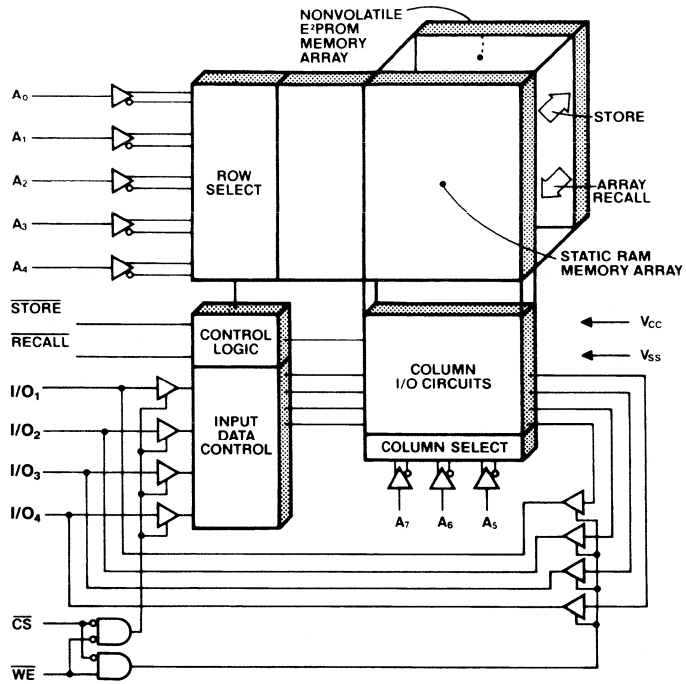


Figure 2: Functional diagram of X2212 memory.

0075-3

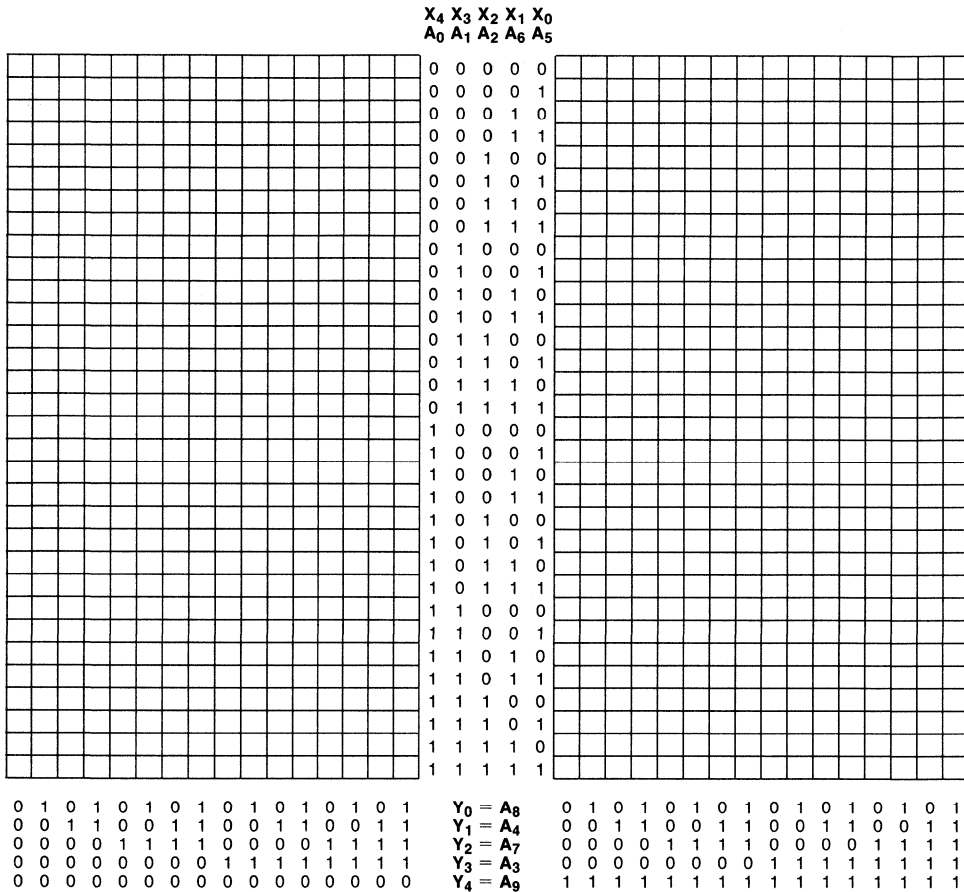


Figure 3: X2201A physical address map.

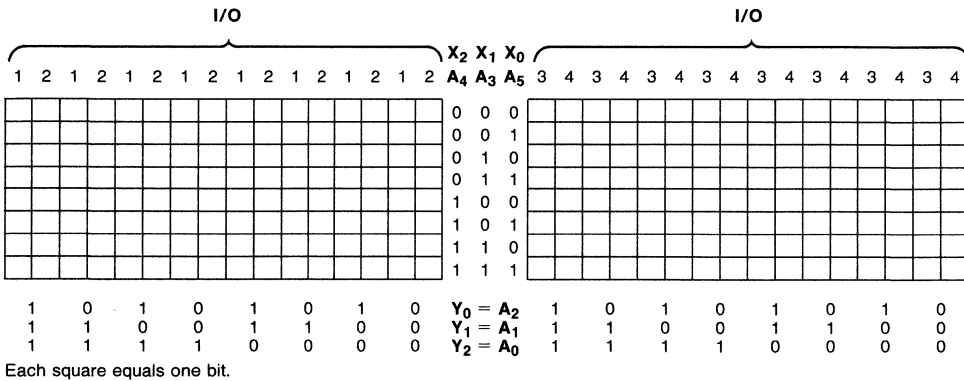
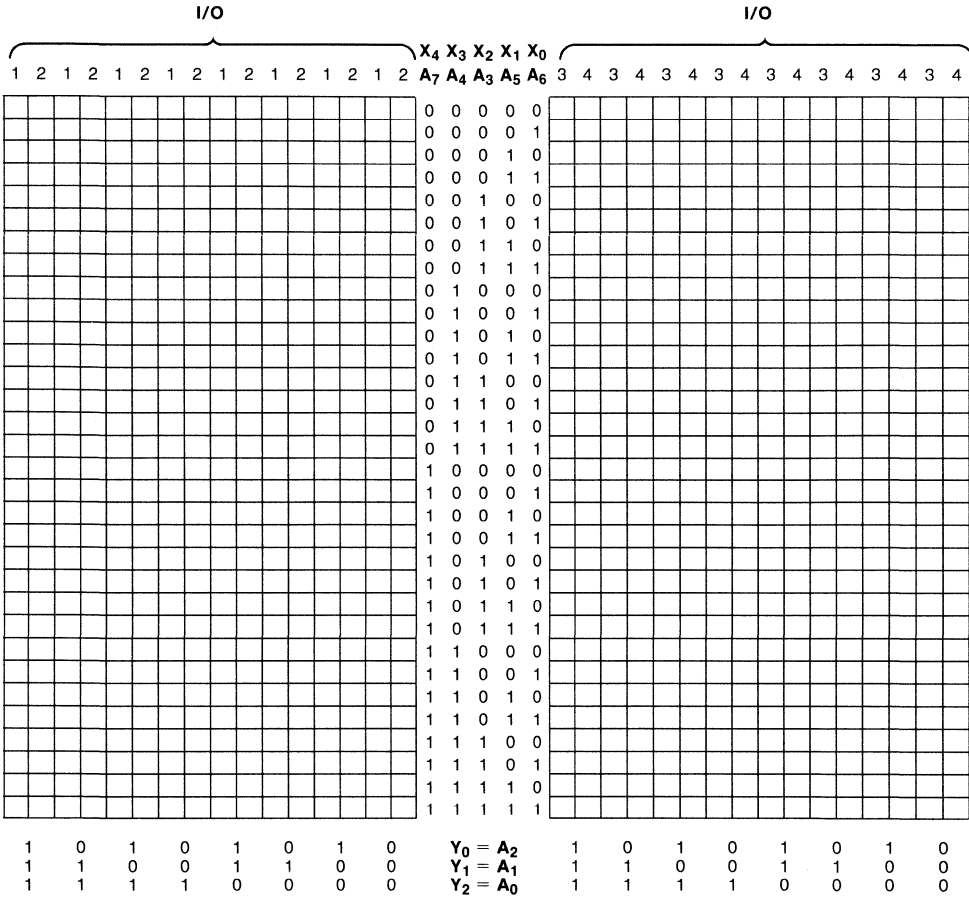


Figure 4: X2210 physical address map.





Each square equals one bit.

Figure 5: X2212 physical address map.

# TECHNOLOGY

Xicor NOVRAM memories store their nonvolatile data on electrically isolated polysilicon gates. These gates are islands of polysilicon surrounded by about 800Å of SiO<sub>2</sub>, one of the best insulators known. This is similar to the structure used in UV light erasable PROMs (UVEPROMs).

Electrons once trapped on the floating (isolated) gates will remain there unless they receive a large energy input from an outside source (e.g., an ultraviolet photon in the case of UVEPROMs), or until a sufficiently high electric field is applied to distort the energy bands sufficiently to allow Fowler-Nordheim tunneling to occur.<sup>1</sup>

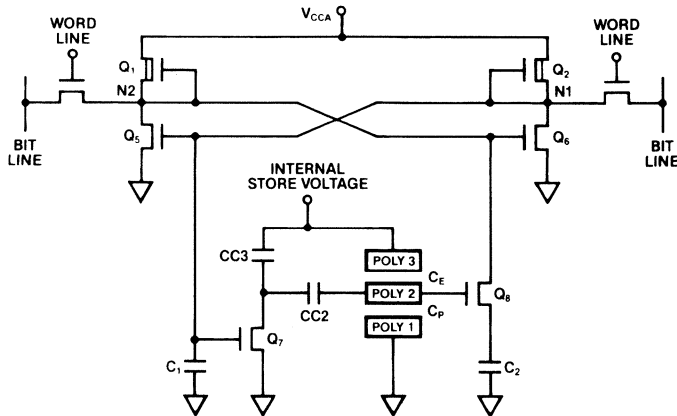
Fowler-Nordheim tunneling, which will be discussed in more detail later in this report, is the mechanism employed to charge and discharge the floating storage gate of Xicor's NOVRAM memories. The storage gate is formed in the second of three layers of polysilicon as illustrated in Figure 6. Electrons move to the floating gate by tunneling from POLY 1 to POLY 2. When the high fields which are used to cause the desired tunneling are not present, the electrons remain trapped on POLY 2.

As Figure 6 illustrates, the NOVRAM memory cell is a conventional six transistor static RAM cell to which a floating gate E<sup>2</sup>PROM cell containing two transistors has been added. During the normal READ/WRITE operations, memory array power supply (V<sub>CCA</sub>) is fixed at the positive supply level (nominally 5V) and the Internal Store Voltage is fixed at ground. Only the six transistors of the static

RAM cell are effective and the operation is exactly that of a conventional six transistor static RAM.

The RECALL operation depends on capacitance ratios. The value of C<sub>2</sub> in Figure 6 is larger than that of C<sub>1</sub>. When the external RECALL command is received, the memory array power supply (V<sub>CCA</sub>) is initially pulled low to equalize the voltages on nodes N<sub>1</sub> and N<sub>2</sub>. These nodes equalize quickly to V<sub>CCA</sub> through the depletion transistors Q<sub>1</sub> and Q<sub>2</sub>. When V<sub>CCA</sub> is then allowed to rise, the node with the lighter capacitive loading will rise more quickly and turn on the pull down transistor on the opposing side, which will keep the more slowly rising node clamped low. If the floating gate is charged positively, Q<sub>8</sub> is turned on, which connects C<sub>2</sub> to N<sub>2</sub>. Thus N<sub>1</sub>, which is loaded by the smaller capacitor C<sub>1</sub>, rises more rapidly, causing the latch to set with N<sub>1</sub> high and N<sub>2</sub> low. If the floating gate is charged negatively, Q<sub>8</sub> is turned off, which isolates C<sub>2</sub> from N<sub>2</sub> and allows N<sub>2</sub> to rise more rapidly than N<sub>1</sub>. Thus the latch is set with N<sub>2</sub> high and N<sub>1</sub> low. During the RECALL operation the Internal Store Voltage remains at ground.

The STORE operation also utilizes capacitance differences to transfer data from RAM to E<sup>2</sup>PROM. When node N<sub>1</sub> is low, transistor Q<sub>7</sub> is turned off. This allows the junction between capacitors CC<sub>2</sub> and CC<sub>3</sub> to float. Since the combined capacitance of CC<sub>2</sub> and CC<sub>3</sub> is larger than that of C<sub>p</sub>, the capacitor between POLY 1 and POLY 2, the floating gate follows the potential of the Internal Store Voltage. Thus when the Internal Store Voltage becomes high (several times V<sub>CC</sub>), a sufficient field exists between POLY 1 and POLY 2 to cause electron tunneling and the floating gate is charged negatively.



0075-7

Figure 6: Schematic diagram of an NOVRAM memory cell showing how a standard six-transistor static RAM cell is merged with a floating gate E<sup>2</sup>PROM cell.

When node  $N_1$  is high, transistor  $Q_7$  is turned on which grounds the junction between  $CC_2$  and  $CC_3$ . Since the capacitance of  $CC_2$  is larger than that of  $C_E$ , the capacitor formed between POLY 2 and POLY 3,  $CC_2$  holds the floating gate near ground when the Internal Store Voltage goes high. In this case the high field exists between POLY 2 and POLY 3 and electrons tunnel from POLY 2 to POLY 3, which discharges the floating gate.

The Internal Store Voltage is at ground except during the STORE operation. Moreover, during the STORE operation all bits are stored simultaneously, which is possible because the RAM bit associated with each  $E^2$ PROM bit acts as a data latch.

## TUNNELING PHYSICS

Because the innovative aspects of NOVRAM and  $E^2$ PROM memories revolve around the nonvolatile storage procedure, it seems appropriate to discuss the storage phenomenon in more detail. As mentioned previously, the storage occurs via a tunneling mechanism first described by Fowler and Nordheim in 1928 and subsequently named after them.<sup>1</sup> The basic idea is illustrated in Figure 7. The energy difference between the conduction and valence bands in Si is about 1.1eV; the energy difference between those bands in  $SiO_2$ , is approximately 9eV. When the two materials are joined, the conduction band in  $SiO_2$  is 3.25eV above that in Si. The differences in valence band energies is even larger (approximately 4eV). Since the thermal energy of an electron averages only 0.025eV at room temperature, the chances of an electron in silicon gaining enough thermal energy to surmount the barrier and enter the conduction band in  $SiO_2$  is exceedingly small. This case is illustrated in Figure 7.

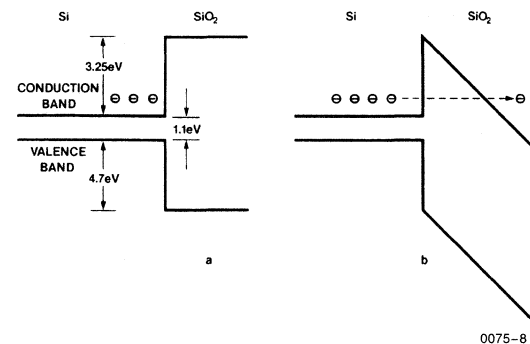


Figure 7: Energy band diagrams of the Si/ $SiO_2$  system in the neutral state (a), and during the store operation (b).

Fowler and Nordheim pointed out that in the presence of a high electric field, the energy bands will be distorted as illustrated in Figure 7b. Under these conditions there is a small but finite probability that an electron in the conduction band in the silicon will tunnel through the energy barrier and emerge in the conduction band of the  $SiO_2$ , as illustrated in Figure 7a.

Fowler-Nordheim emission was observed early in this century for the case of electrons being emitted from metals into vacuum, and in 1969 Lenzlinger and Snow observed this phenomenon for the Si- $SiO_2$  system.<sup>2</sup> The Fowler-Nordheim current increases exponentially with applied field and becomes readily observable (i.e.,  $J \sim 10^{-6}$  A/cm<sup>2</sup>) for the Si- $SiO_2$  system in which the Si surface is smooth for fields on the order of 10 MV/cm.

It has been known for some time that “enhanced” electron emission currents could be observed for Si- $SiO_2$  systems for which the Si surface has a texture. (Texture in this context means that the Si surface has features on the order of a few hundred angstroms.)<sup>3-5</sup> These enhanced currents occur at applied fields with values smaller than one quarter of those necessary for the same current from a smooth surface. It has been thought that the enhanced emission occurs because of locally enhanced fields near the top regions of the features on the surface.

Lewis attempted to model Fowler-Nordheim tunneling from a textured surface by calculating current from a number of hemispheres set in a plane.<sup>6</sup> Attempts to quantitatively fit experimentally observed currents with this model have not been very successful. Hu, et al, for example, found that to fit their data to existing theory it was necessary to assume an energy barrier of approximately 1eV between conduction bands in Si and  $SiO_2$ .<sup>7</sup> Even with this assumption, the fit was poor because the measured current increased more rapidly than the calculated values, as is illustrated in Figure 8.

Because of the importance of tunneling to the operation of its products, Xicor decided to adequately characterize and model tunnel emission from textured polycrystalline silicon (poly) surfaces. One avenue of exploration was to characterize the physical topology of the tunneling structure. Figure 9 is a scanning electron micrograph (SEM) of the emitting (top) surface of a layer of polysilicon from which the oxide has been removed for clarity. As shown in the micrograph, this surface is composed of a densely packed array of features reminiscent of a cobblestone street. A count of these features on SEM photos of material from several lots determined that

there is an average of about 50 features per square micron. A transmission electron microscope (TEM) cross-section of a tunneling structure is shown in Figure 10. This photo demonstrates the conformal nature of the structure. The top surface of the prior deposition of polysilicon is formed into a series of "hillocks" 200–300Å high and 1000–1500Å across the base. The free surface of the oxide grown on this silicon replicates the silicon surface. Thus, polysilicon deposited atop the prior polysilicon layer subsequent to oxidation has dimples on its undersurface occurring over the already existing "hillocks".

The topology of the polysilicon surfaces causes the electric field lines to no longer be parallel as in the case of parallel emitting and collecting surfaces, but rather to diverge and converge in response to the local topology as is illustrated in Figure 11. As shown, the field lines converge near surfaces of positive curvature (i.e., bumps) and diverge near surfaces of negative curvature (i.e., dimples). Since Fowler-Nordheim tunneling depends exponentially on the electric field at the surface of the polysilicon, a good model of the electron emission requires an accurate knowledge of the field over the complete surface.

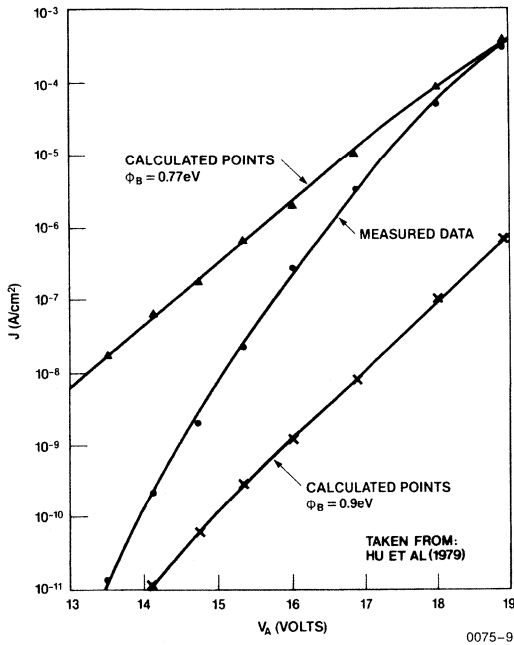
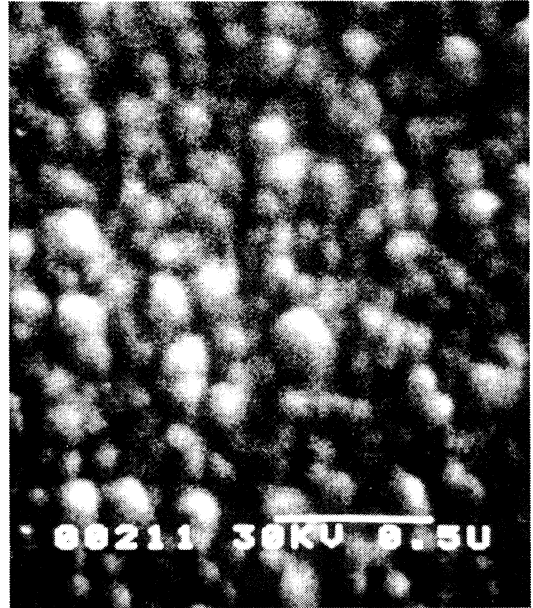
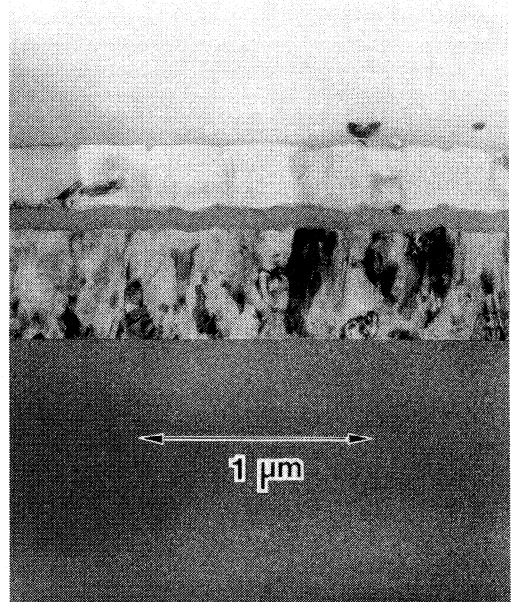


Figure 8: Current vs. applied voltage for current from textured poly surface emitted through 1760Å of thermal SiO<sub>2</sub> compared with calculations based on previously available theory.



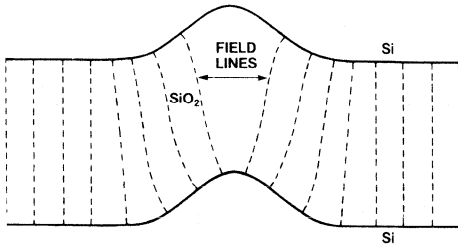
0075-10

Figure 9: Scanning electron microscope (SEM) photograph of top emitting textured poly surface with oxide removed. The 0.5 μ-long bar gives the scale.



0075-1

Figure 10: Transmission electron microscope (TEM) photograph of a cross-section through a textured tunneling structure. The one micron-long arrow shows the scale.



0075-11

Figure 11: Sketch illustrating the manner in which field lines converge near convex feature and diverge near concave feature.

Until recently, this field problem was one of the unsolved problems of mathematical physics. (It is classically known as the "lightning rod problem".) Roger Ellis, a member of the Xicor staff, has solved this problem.<sup>8</sup> The technique used differential geometry to transform Euclidean space into a space in which the field lines were parallel. The electrostatics problem was solved in this space and the solution transformed back into the original space. The tunnel current was found to be described in a spherical coordinate system by the equation:

$$J_{\text{collecting}} = \frac{\left[ \int_s \frac{q^3 E^2}{8\pi\hbar\phi_B} \exp\left\{ \frac{-4(2m)^{1/2}\phi_B^{3/2}}{3\hbar q E} \right\} ds \right]_{\text{emitting}}}{\left[ \int_s ds \right]_{\text{collecting}}} \quad (1)$$

where the electric field, E, is given by

$$E = \frac{V_A}{\xi(S_2) - \xi(S_1)} \left[ \left( \frac{d\phi^2}{dr} \right) + \frac{1}{r^2} \right]^{1/2} \frac{d\xi}{d\phi} \quad (2)$$

and

$$\xi = \frac{1}{\left| \frac{dr}{d\phi} \right|} \frac{de_t}{d\phi} (\vec{e}_t)$$

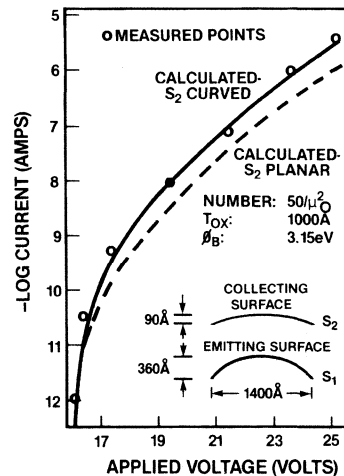
is the curvature of the surface at which the field is evaluated.<sup>9</sup>

This expression has several interesting properties. One is that the field depends on the difference of the curvatures of the emitting and collecting surfaces. Another is that the electric field also depends on the derivative of the curvature of the emitting surface.

To verify the accuracy of this expression, the current-voltage (J-V) characteristics of a textured polysilicon tunnel structure were experimentally determined and compared with those predicted by equation (1). Because of the field enhancement on the bumps, a higher current is expected at a given applied voltage polarity which causes electron emission from the bumps than for that polarity which

causes emission from the dimples. Thus, by analogy with a diode, the polarity with the bumps negative (higher current emitted) is called the forward bias direction and the other polarity is called the reverse bias direction.

Figure 12 shows the results of comparing experimental and calculated values for the forward bias condition. As can be seen, theory and experiment agree within about 20% over seven orders of magnitude in current. The parameters used in calculating the predicted currents were not arbitrarily chosen. The value of the oxide/silicon conduction band barrier,  $\phi_B$ , was taken to be 3.15eV as measured by Weinberg.<sup>10</sup> The feature density ( $50\mu$ )<sup>2</sup> and the bump base and height are typical of those seen on SEMs and TEMs such as Figures 9 and 10, respectively. The dashed line in Figure 12 is the current which would be predicted if the top (i.e., collecting) electrode were flat rather than dimpled. This illustrates the effect of the collecting surface curvature on the field at the emitting surface.

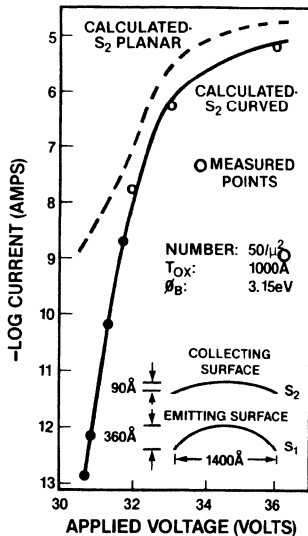


0075-12

Figure 12: Forward tunneling characteristic comparing the measured data with curves calculated for a concave and a planar collecting surface.

To further verify equation (1), the reverse bias current was measured on the same device used for the forward bias case. The results are compared with the predicted current in Figure 13. This shows about 20% agreement over eight orders of magnitude in current with the same parameters used as in calculating the forward bias case. Clearly, the model does an excellent job of predicting the measured current.





0075-13

Figure 13: Reverse tunneling characteristic comparing the measured data with curves calculated for a concave and planar emitting surface.

Several points of interest can be observed in Figure 13. One point is that at a voltage at which the forward current is saturating (25V), the reverse current is unobservable (extrapolation of the measured current predicts  $\sim 10^{-27}A$ ). Another point is that the current emission predicted from a flat top surface is greater than that predicted from a dimpled top surface. Moreover, the current emitted from a flat top surface decreases more slowly with decreasing voltage than that from a dimpled flat surface. This latter fact is important for data retention as will be discussed in the next section.

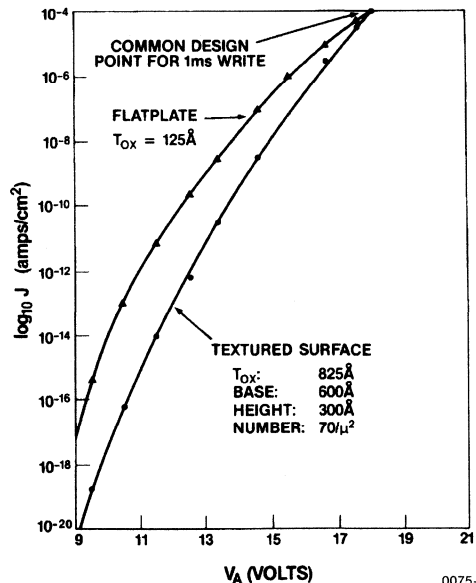
In summary, Xicor is able to accurately model the tunnel current emitted from textured poly surfaces through  $SiO_2$  layers. The magnitude of the tunnel current as well as its voltage dependence are dependent upon the surface topology. Thus, we have the means to optimize the emission characteristics. Lastly, the asymmetric nature of the tunnel emission makes possible cell designs which are better adapted to particular requirements than is possible with symmetric tunnel characteristics—just as a diode offers more design possibilities than does a resistor.

## DATA RETENTION

As was suggested in the previous section, textured poly tunneling structures have a significant advantage in data retention, in comparison with those employing flat surfaces and thin oxides. One basis

for this advantage is illustrated in Figure 14, in which the current-voltage (J-V) characteristics of a tunneling device which employs a thin oxide between planar surfaces is compared with a tunneling device which employs a thick oxide between textured silicon surfaces. For this comparison we match the currents in the high current region since most memories are designed to program in about the same time period ( $\sim 10$  ms). As can be seen, the same current can be obtained from a smooth surface with 125Å thick tunnel oxide or from a textured surface with an 825Å thick tunnel oxide. Note however, that at lower values of applied voltage typical of read and storage conditions, the current emitted from a textured surface is approximately four orders of magnitude lower than that from a smooth surface.

These differences may become even more significant as devices are scaled. It is clear that, in order to scale the memory properly, lower programming voltages are needed so that the isolation widths and device channel lengths can be reduced both in the memory array and in the peripheral circuitry. However, for a typical part which stores data in 3 ms and must retain it for 10 years, the tunneling current under storage and reading conditions must be at least  $10^{11}$  times smaller than under programming conditions because the retention time is  $10^{11}$  times

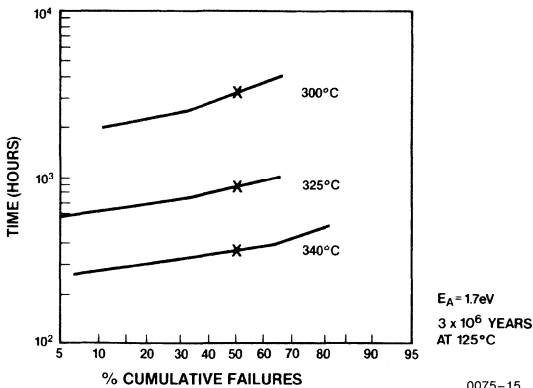


0075-14

Figure 14: Comparison of calculated tunneling J-V curves for emission from a planar and a textured structure. The devices were designed to have the same emission in the high current regime where programming takes place.

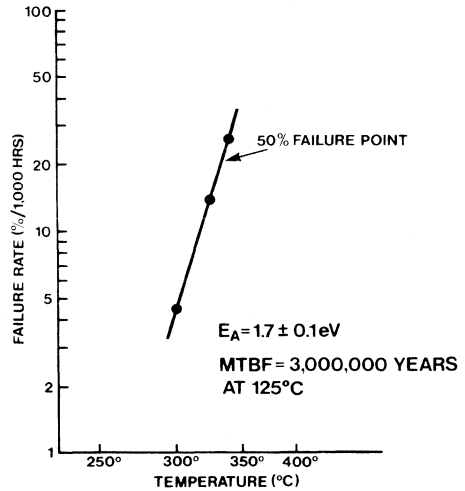
longer than the storage time. Actually, for a margin, one would design for a difference in currents of  $10^{13}$  to  $10^{14}$ . For planar surface tunneling structures, this may be a difficult design constraint because the slope of the J-V curve is fixed, which means that the maximum allowed read voltage drops with the programming voltage on a volt-for-volt basis, not proportionately. On the other hand, textured surface tunneling structures, in their current manifestation, have a steeper J-V characteristic than planar ones and the J-V characteristic of a textured structure can be tailored to yield a steeper curve if desired. This means that for a given maximum read voltage, a textured structure requires a lower programming voltage which leads to better scaling.

To verify the excellent data retention expected of Xicor NOVRAMs, a study was carried out to measure data loss as a function of temperature. Figure 15 shows log cumulative data loss vs. log time for 100 samples of X2210's at each of three temperatures. Data loss is defined as occurring when the first bit in the array loses data. As shown in Figure 15, high temperatures were required to obtain appreciable data loss in experimentally useful times. Note that even at 300°C, 2000 hours (~ 3 months) are required to begin to see data loss. Figure 16 shows the result of calculating failure rates based on these results and plotting vs. inverse temperature. Since the rates fall in a straight line, we can extract an activation energy and extrapolate to lower temperatures (see the next section for a discussion of activation energies). The result is that the experimental value of the activation energy is 1.7eV and the mean time for data loss for this mechanism (which we believe to be the fundamental loss mechanism for this technology) is 3 million years for data retention at 125°C.



0075-15

Figure 15: Log cumulative data loss vs. log time for three storage temperatures on samples of 100 X2210's. Data loss is defined to occur when the first bit in an array loses data.

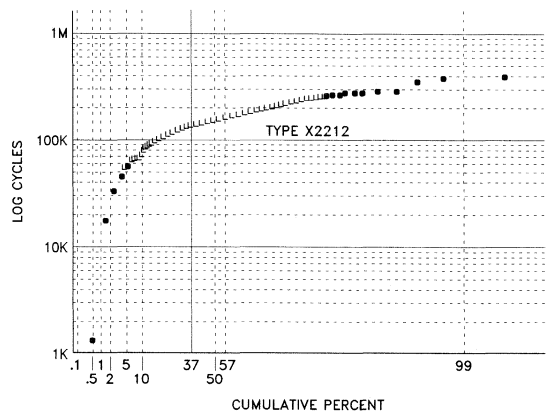


0075-16

Figure 16: Log data loss rate vs. inverse temperature for X2210's.

## ENDURANCE

The endurance of Xicor NOVRAMs is monitored on a regular basis. Figure 17 shows typical endurance data on 100 units of X2212 from five endurance monitor lots plotted on an extreme value distribution. All of the units tested exceeded the 1,000 data changes/bit limit specified for this device.

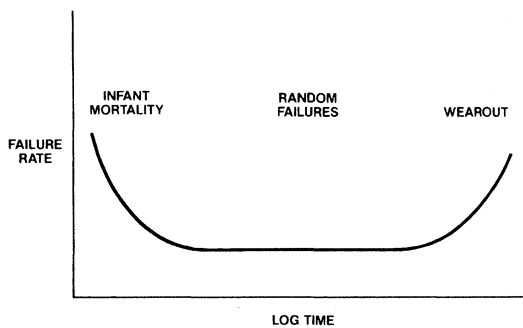


0075-20

Figure 17: Extreme value distribution plot of X2212.

# BASIC RELIABILITY CONCEPTS

There are several concepts basic to most reliability work. One is the long established observation that failure rates follow the bathtub-shaped curve illustrated in Figure 18. There is an infant mortality region characterized by a rapidly declining failure rate as the "weak" parts are eliminated from the population, a random failure characterized by an invariant or slowly declining failure rate, and a wear-out region characterized by an increasing failure rate as the units reach the end of life.



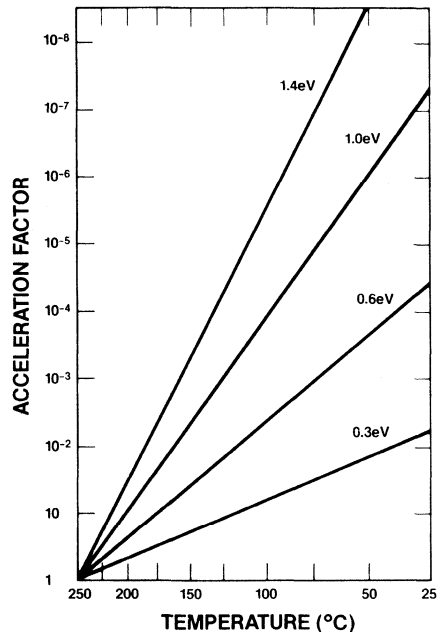
0075-17

Figure 18: Illustration of bathtub curve of failure rates showing regions in which infant mortality, random failures, and wearout mechanisms dominate the failure rate.

Each region of the failure rate curve has specific failure modes which predominate. For example, the infant mortality region is dominated by failures which arise from manufacturing defects. Table I gives a summary of common failure mechanisms and stresses which may be used to accelerate the failure rates of the various mechanisms which have been culled from the literature.<sup>11-14</sup>

The classic parameter used to accelerate failure rates is temperature. It is known that a very broad class of failure mechanisms have a temperature dependence proportional to  $\exp(-E_a/kT)$  where  $E_a$  is called the activation energy,  $k$  is Boltzmann's constant, and  $T$  is the absolute temperature. This is true because a number of basic physical phenomena such as diffusion rates and chemical reaction rates have this dependence. The significance of this is that if the activation energy is known for the failure mechanisms in question, then the failure rates arising from these mechanisms can be measured at

elevated temperature where they are high enough to be conveniently measured and extrapolated back to lower operating temperatures where the failure rates may be so low as to require an inconveniently large number of device hours to measure. The relationship which allows one to translate failure rates from one temperature to another is known as the Arrhenius relation. Figure 19 illustrates this relation for a number of common values of activation energy.



0075-18

Figure 19: Acceleration factor vs. temperature calculated for various activation energies from Arrhenius relation.

# RELIABILITY TESTING

Five types of tests were conducted to establish the reliability of the devices:

- 1) High temperature dynamic lifestest.
- 2) Data retention bake.
- 3) High temperature reverse bias.
- 4) Lifestest monitor.
- 5) Environmental.

These tests are discussed after Table I.



Failure Mechanism	Type	Activation Energy	Detection Method
Ionic Contamination	Infant/ Random/ Wearout	1.0eV	High Temp. Bias
Surface Charge	Wearout	0.5–1.0eV	High Temp. Bias
Polarization	Wearout	1.0eV	High Temp. Bias
Electromigration	Wearout	1.0eV	High Temp. Operating Life
Microcracks	Random	—	Temperature Cycling
Oxide Rupture	Infant/ Random	0.3eV	High Temp. Operating Life
Silicon Defects	Infant/ Random	0.3eV	High Temp. Bias
Oxide Defect Leakage	Infant/ Random	0.6eV	High Temp. Operating Life
Electron Trapping In Oxide	Wearout	—	Low Temp., High Voltage Operating Life

Table 1: MOS failure mechanisms.

## High Temperature Dynamic Lifetest

This is the usual data from which failure rate predictions are made. For this to be a valid predictor of failure rate, the parts must function as they would in normal operation. Thus, overly elevated temperatures at which the unit does not function internally are to be avoided since this may lead to overly optimistic predictions.

Xicor gathers this data at 125°C ambient which is within the known operating range of the units under test. The stimulus pattern consists of recalling a known pattern, writing an all one's pattern over the recalled pattern bit by bit, reading the all one's pattern, writing its complement, reading the complement and then beginning over again.

The units in lifetest are tested at 168, 500, 1000, and 2000 hours to verify that they are still within specification. The first step of the readout tests is to recall the information stored in the nonvolatile section of memory to verify that the previously stored pattern is still retained. If so, the memory is completely exercised over voltage including verification of the STORE function. Finally, the predetermined pattern is restored to memory for the next lifetest period.

## Data Retention Bake

This test is sometimes referred to as a storage bake. The term "data retention bake" better describes the principal function it serves in the case of electrically programmable nonvolatile memories which is to measure how fast charge leaks away from the floating gate.

In this test, a pattern which represents all floating gates charged positive is stored and the devices are baked at 250°C for the cerdip (ceramic dual-in-line) package and 150°C for plastic (dual-in-line) package with no bias applied. At intervals the memory is removed from bake, and the nonvolatile data recalled and checked for accuracy. The data is not restored at readouts in order to ascertain the worst case retention. Since Xicor warrants cycling endurance of various values, this test was performed on parts specified for 1000 cycle endurance which had performed 1000 complete data alterations, as well as on parts which had not received this treatment.

## HTRB

HTRB stands for High Temperature Reverse Bias, a term which originated with bipolar circuits, in which case the test reverse biased the junctions of all of the input stages. For MOS circuits, a better term would be high temperature static bias. In this stress, which Xicor carries out at 150°C,  $V_{SS}$  is grounded and a static positive voltage is applied to all of the inputs and outputs, as well as to  $V_{CC}$ . This has the effect of applying a static bias equal to the power supply across the gate oxides of the circuit transistors. This stress is intended to expose failures which might occur as a result of drift of mobile ionic contaminants or latent defects in the gate oxides.

---

It is known that many defects are accelerated by voltage as well as temperature. For example, it has been shown by Crook that the failure rate of oxide defects increases  $10^7$  times per MV/cm increase in the electric field.<sup>15</sup> For this reason, HTRB stresses were conducted with both 5.5V and 7.5V bias applied to the units under test.

## Lifetest Monitor

In order to assure a continuous supply of the highest quality and reliability possible to our customers, a weekly lifetest monitor is maintained.

This monitor is used at Xicor for two purposes. First, it is used to monitor the infant mortality rate which is an indicator of manufacturing defects. If an unusually high failure rate were to be observed, a corrective action could be taken before defective units are shipped to customers. Secondly, a long term failure rate is also monitored. This establishes a way to ensure that long term reliability is maintained.

Each week approximately 250 units of X2212 devices are placed in a dynamic lifetest at 125°C for 168 hours. Also, monitor units of the first week of each period remain in dynamic lifetest for up to 1000 hours.

## Package Environmental Tests

MIL-M-35810 and MIL-STD-883, Method 5005, Group C and D have been the guide for environmental testing for the cerdip package. Table II lists

the tests, the test conditions and test results. All lots passed the 883 qualification criteria.

Because of the nature of the plastic package, additional tests were done. These tests are 85°C/85% RH (both biased and unbiased) lifetest, temp cycling (200 cycles) and saturated storage test at 2 ATM (autoclave).

## RESULTS

Tables IIIA and IIIB exhibit the results of dynamic lifetest of X2210 and X2212 in cerdip package and plastic package, respectively. Table IIIA shows zero failure result in  $6 \times 10^5$  device hours on 1700 units of X2210 and X2212. Table IIIB shows two failure results in  $1.7 \times 10^6$  device hours on 5055 units of X2210 and X2212. The causes of the failures were also listed in Table IIIB. In addition, Table IIIB includes lifetest monitor data since plastic units are used.

Tables IVA and IVB show the results of 150°C static lifetest at 5.5V for cerdip and plastic. No failures were detected on both package types, out of 121 units for cerdip and 245 units for plastic.

Tables VA and VB show the results of 150°C static lifetest at 7.5V applied bias. Increasing  $V_{CC}$  from 5.5V to 7.5V increases the field across the gate oxide from  $6.875 \times 10^5$  V/cm to  $9.375 \times 10^5$  V/cm. According to Crook this increase in field should accelerate the failure rate by about 56 times. In cerdip, one failure was observed at the 48 hour readout. For oxide breakdown, out of 250 units tested in plastic, no failures were seen.

Test	MIL-STD-883 Test Method	Conditions	LTPD	Accept #	Results
Temp. Cycling	1005	Test Condition C (10 cycle, -65°C to +125°C)	15	0/15	0/175
Constant Acceleration	2001	Test Condition E (30,000g, Y1 axis only)			0/175
Seal —Fine —Gross	1014	Test Condition B ( $5 \times 10^{-8}$ cc/min) Test Condition C			0/175 0/175
Lead Integrity	2004	Test Condition B2 (Lead Fatigue)	15	0/15	0/213
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/213 1/213
Thermal Shock	1011	Test Condition B (15 cycles, -55°C to +125°C)	15	0/15	0/203
Temp. Cycling	1010	Test Condition C (100 cycles)			0/203
Moisture Resistance	1004				0/203
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/203 0/203
Internal Water Vapor Content	1018	5,000 ppm max. water content at 100°C	—	0/3 or 1/5	0/6
Mechanical Shock	2002	Test Condition B (1500g peak, 3 axis)	15	0/15	0/192
Vibration Variable Frequency	2007	Test Condition A (20g peak, 3 axis)			0/192
Constant Acceleration	2001	Test Condition E			0/192
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/192 0/192
Salt Atmosphere	1009	Test Condition A	15	0/15	0/144
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/144 0/144
Adhesion of Lead Finish	2025		15	0/15 (# of leads from 3 devices)	0/18
Lid Torque	2024		—	0/5	0/15

Table II: Environmental test for 18-lead cerdip package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	403	0	383	0	99	0	97	$1.3 \times 10^5$
2 (2212)	0	350	0	324	0	99	0	98	$1.2 \times 10^5$
3 (2212)	0	338	0	334	0	99	0	98	$1.2 \times 10^5$
4 (2210)	0	294	0	284	0	99	0	97	$1.2 \times 10^5$
5 (2210)	0	315	0	312	0	99	0	98	$1.2 \times 10^5$
<b>Totals</b>	0	1700	0	1637	0	495	0	488	$6.0 \times 10^5$

Table IIIA: Stress dynamic lifetest at 125°C—cerdip package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	575	0	573	0	99	0	97	0	97	$2.5 \times 10^5$
2 (2212)	2[a]	570	0	565	0	99	0	98	0	98	$2.5 \times 10^5$
3 (2212)	0	577	0	577	0	99	0	96	0	96	$2.5 \times 10^5$
4 (2210)	0	573	0	570	0	99	0	99	0	98	$2.5 \times 10^5$
5 (2212)	0	570	0	570	0	99	0	99	0	98	$2.5 \times 10^5$
6 (Monit.)	0	2190	0	2183	0	297	0	297	—	—	$5.1 \times 10^5$
<b>Totals</b>	2	5055	0	5038	0	792	0	786	0	487	$1.7 \times 10^6$

[a] = one x-decoder failure due to blown oxide 0.3eV  
 one word line failure due to blown oxide 0.3eV

Table IIIB: Stress dynamic lifetest at 125°C—plastic package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	25	0	23	0	23	0	23	0	23	44896
2 (2212)	0	25	0	25	0	25	0	25	0	25	48800
3 (2212)	0	25	0	23	0	23	0	23	0	23	44896
4 (2210)	0	25	0	25	0	25	0	25	0	25	48800
5 (2210)	0	25	0	25	0	25	0	25	0	25	48800
<b>Totals</b>	0	125	0	121	0	121	0	121	0	121	$2.4 \times 10^5$

Table IVA: Stress 5.5V HTRB at 150°C—cerdip package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	50	0	49	0	49	0	49	46648
2 (2212)	0	50	0	50	0	50	0	49	47100
3 (2212)	0	50	0	50	0	50	0	50	47600
4 (2210)	0	50	0	50	0	50	0	50	47600
5 (2212)	0	50	0	49	0	47	0	47	44984
<b>Totals</b>	0	250	0	248	0	246	0	245	$2.3 \times 10^5$

Table IVB: Stress 5.5V HTRB at 150°C—plastic package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	25	0	25	0	25	0	25	23800
2 (2212)	1[a]	25	0	24	0	24	0	24	22848
3 (2212)	0	25	0	25	0	25	0	25	23800
4 (2210)	0	25	0	25	0	25	0	25	23800
5 (2210)	0	25	0	25	0	25	0	25	23800
<b>Totals</b>	1	125	0	124	0	124	0	124	$1.2 \times 10^5$

[a] = Blown oxide 0.3eV

Table VA: Stress 7.5V HTRB at 150°C—plastic package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	50	0	48	0	48	0	48	45696
2 (2212)	0	50	0	50	0	50	0	48	46600
3 (2212)	0	50	0	50	0	50	0	50	47600
4 (2210)	0	50	0	50	0	50	0	50	47600
5 (2212)	0	50	0	48	0	48	0	48	45696
<b>Totals</b>	0	250	0	246	0	246	0	244	$2.3 \times 10^5$

Table VB: Stress 7.5V HTRB at 150°C—plastic package.

Tables VIA, VIB, VIIA and VIIB show the results of 250°C and 150°C retention bake for cerdip and plastic, respectively. Retention bake was done both before and after 1000 data change cycles on units that are rated for 1000 data change cycles. At 150°C no failures were detected before nor after 1000 data changes on a total of 125 units for 1000 hours. At 250°C, the data on uncycled devices shows 3 units failed from 250 units for 2000 hours. The data on cycled devices shows 4 units failed from 125 units for 2000 hours. These results do not have statistically significant difference in overall failure rate. Close examination shows a tendency for the cycled failures to be more scattered, while uncycled failures are more concentrated at 1000 and 2000 hour

readouts. This kind of data should not be surprising, as an oxide defect, which had been accelerated by the high electric field, became manifest during store operation. The retention failure rate for 1000 hours at 250°C is at the range of 1% to 2%, which is about half of that previously reported for EPROMs.<sup>16</sup> Retention data reported for other E<sup>2</sup>PROM technologies would indicate that the present NOVRAM retention results are greatly superior.<sup>17</sup>

Tables VIII and IX represent 85/85 lifetest with and without voltage bias, respectively. As indicated by the data, no failures were observed in both the 5.5V biased and the unbiased groups for a total of  $5 \times 10^5$  device hours.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	50	0	50	0	50	0	49	0	48	95100
2 (2212)	0	50	0	50	0	50	0	50	1	47	94600
3 (2212)	0	50	0	50	0	50	1	50	1	48	95600
4 (2210)	0	50	0	50	0	50	0	50	0	50	97600
5 (2210)	0	50	0	50	0	50	0	49	0	49	96100
<b>Totals</b>	0	250	0	250	0	250	1	248	2	242	$4.8 \times 10^5$

Table VIA: Stress bake at 250°C—cerdip package.



Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	25	0	25	0	25	0	25	23800
2 (2212)	0	25	0	25	0	25	0	25	23800
3 (2212)	0	25	0	25	0	25	0	25	23800
4 (2210)	0	25	0	25	0	25	0	25	23800
5 (2212)	0	25	0	25	0	25	0	25	23800
<b>Totals</b>	0	125	0	125	0	125	0	125	$1.2 \times 10^5$

Table VI B: Stress retention bake at 150°C—plastic package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	25	0	25	1	24	0	23	1	23	45468
2 (2212)	0	25	0	25	0	25	0	25	0	25	48800
3 (2212)	1	25	0	24	0	24	1	24	0	23	45848
4 (2210)	0	25	0	25	0	25	0	25	0	25	48800
5 (2210)	0	25	0	25	0	25	0	25	0	25	48800
<b>Totals</b>	1	125	0	124	1	123	1	122	1	121	$2.4 \times 10^5$

Table VIII A: 250°C Retention bake—cycled cerdip unit.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	25	0	25	0	25	0	25	23800
2 (2212)	0	25	0	25	0	25	0	25	23800
3 (2212)	0	25	0	25	0	25	0	25	23800
4 (2210)	0	25	0	25	0	25	0	25	23800
5 (2212)	0	25	0	25	0	25	0	25	23800
<b>Totals</b>	0	125	0	125	0	125	0	125	$1.2 \times 10^5$

Table VI B: 150°C Retention bake—cycled plastic unit.

Lot #	500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	
1 (2212)	0	50	0	50	41600
2 (2212)	0	50	0	50	41600
3 (2212)	0	50	0	50	41600
4 (2210)	0	50	0	50	41600
5 (2212)	0	50	0	50	41600
<b>Totals</b>	0	250	0	250	$2.1 \times 10^5$

Table VIII: Biased 85/85—plastic units with  $V_{CC} = 5V$ .

Lot #	500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	
1 (2212)	0	50	0	50	41600
2 (2212)	0	50	0	50	41600
3 (2212)	0	50	0	50	41600
4 (2210)	0	50	0	50	41600
5 (2212)	0	50	0	50	41600
<b>Totals</b>	0	250	0	250	$2.1 \times 10^5$

Table IX: Biased 85/85—plastic units with  $V_{CC} = 0V$ .

Lot #	200 Cycles	
	# Fail	# In
1 (2212)	0	50
2 (2212)	0	50
3 (2212)	0	50
4 (2212)	0	50
5 (2210)	0	50
<b>Totals</b>	0	250

Table X: Temperature cycles (method 1010)—plastic package.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 (2212)	0	25	0	25	0	25	0	25	23800
2 (2212)	0	25	0	25	0	25	0	25	23800
3 (2212)	0	25	0	25	0	25	0	25	23800
4 (2210)	0	25	0	25	0	25	0	25	23800
5 (2212)	0	25	0	25	0	25	0	25	23800
<b>Totals</b>	0	125	0	125	0	125	0	125	$1.2 \times 10^5$

Table XI: Dynamic lifetest at 10°C—plastic packaged units.

Figure 20 shows a bar graph of the autoclave results for plastic package. Cumulative failures steadily increased for the first 400 hours with sharp increase at approximately 500 hours. Figure 20 shows the 500 hour mark for the plastic package in the 24% range. The discrepancy between autoclave and 85°C/85% RH lifetest results can be explained by the two causes of failure. During the saturated storage (autoclave), failure rate is dependent on the galvanically induced ionic currents flowing in a layer of water on the surface of the die. This layer of water is accumulated after plastic has debonded from the die which causes corrosion to concentrate on the bonding pad. The 85°C/85% RH lifetest produced more widespread corrosion due to phosphorous in the passivations, and debonding is not a pre-

requisite for this type of failure.<sup>21, 22</sup> Since corrosion on the bonding pad is only one of the failure modes which can occur in 85°C/85% RH lifetest, it would be a better indicator for normal operation.<sup>21</sup>

Table X shows the result of the temperature cycling for plastic packages. No failures were observed. The test used 200 temperature cycles for +125°C to -65°C, air to air. (MIL-STD-883, Method 1010) indicates that the plastic packaged device would perform very well under normal temperature variations.

Table XI shows the results (no failures) of low temperature dynamic lifetest. The lack of failures indicates that typical semiconductor failure modes are not a factor in this technology.

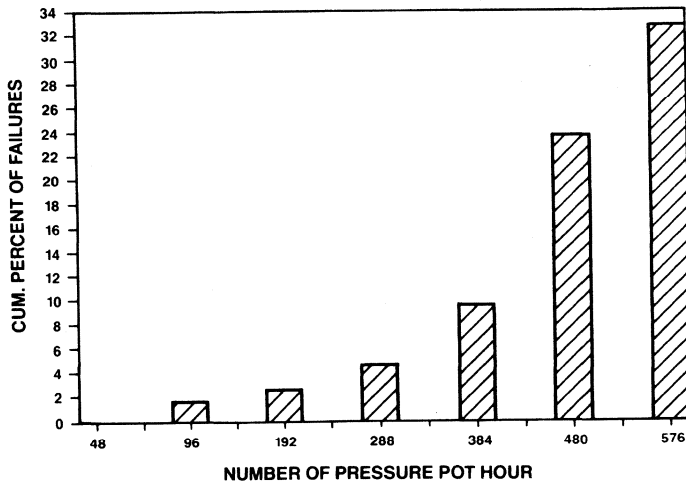


Figure 20: Pressure pot result.

0075-19

## CALCULATION OF PREDICTED FAILURE RATE

There is no simple, one-step formula for inferring a predicted failure rate from the experimental data. Instead, the failures of each individual activation energy must be treated differently. The first step is to calculate the equivalent device hours at the ambient temperature of interest, utilizing the Arrhenius relationship discussed earlier. This calculation should be carried out for every mechanism observed or expected. For example, the calculation for the 0.3eV activation energy oxide rupture mechanism should be carried out whether this failure mechanism is observed or not, since this mechanism is always anticipated in MOS integrated circuits. The extrapolation should be carried out utilizing the junction temperature at the ambient temperature of interest and not the ambient temperature itself. The upper confidence limit is then calculated for the failure rate for each activation energy. The upper confidence limits for the various activation energies are then summed for a total failure rate prediction. The meaning of the "upper confidence level" is that with a certainty, or probability, of a certain level we can say that the true value is less than the stated value. Thus, the confidence level rate calculated is non-zero even for the case where no failures are observed because we can't be sure that there will be none.

Two calculations were performed to separate short term failure rates (infant mortality) and long term failure rate (expected failure rate). This was done to obtain a better picture of the expected failure rates.

Long term failure rates are tabulated in Table XII based on the data in Tables III-V. Voltage acceleration is applied for the 0.3eV activation energy failure mode typical of oxide breakdown. No voltage acceleration is applied to the 0.6eV and 1.0eV failure modes because the dependence for these has not been established. These data lead to a predicted long term failure rate in plastic of 39 FIT (0.0039%/1000 hr) at 60% UCL at 70°C ambient and 18 FIT (0.0018%/1000 hr) at 60% UCL at 55°C ambient. In cerdip the corresponding values are 85 FIT (0.0085%/1000 hr) at 60% UCL at 70°C ambient and 45 FIT (0.0045%/1000 hr) at 60% UCL at 55°C ambient. From these numbers, it should not be concluded that the parts are more reliable in plastic than in cerdip but rather that since there are more hours in plastic than cerdip the uncertainty is reduced and hence the UCL (upper confidence level) is lower. The best single point estimate of the reliability of the part is probably obtained by combining the data on the units in plastic and cerdip packages. This leads to estimated failure rate of 39 FIT (0.0039%/1000 hr) at 70°C ambient and 60% UCL and 16 FIT (0.0016%/1000 hr) at 55°C ambient and 60% UCL.

The above calculations of long term failure rates were done excluding the data for the first 48 hours



PLASTIC									
Activation Energy	Hours at 125°C	Hours at 150°C	Number of Failures	Equivalent Hours at 70°C	Expected Value of Failure Rate at 70°C	60% UCL Failure Rate at 70°C	Equivalent Hours at 55°C	Expected Value of Failure Rate at 55°C	60% UCL Failure Rate at 55°C
0.3eV	$1.75 \times 10^6$	$4.91 \times 10^5$	0	$9.31 \times 10^7^*$	—	9.8	$1.40 \times 10^8$	—	7
0.6eV	$1.75 \times 10^6$	$4.91 \times 10^5$	0	$3.94 \times 10^7$	—	26	$8.86 \times 10^7$	—	10
1.0eV	$1.75 \times 10^6$	$4.91 \times 10^5$	0	$3.07 \times 10^8$	—	3	$1.19 \times 10^9$	—	1
<b>Total</b>					—	39		—	18
CERDIP									
Activation Energy	Hours at 125°C	Hours at 150°C	Number of Failures	Equivalent Hours at 70°C	Expected Value of Failure Rate at 70°C	60% UCL Failure Rate at 70°C	Equivalent Hours at 55°C	Expected Value of Failure Rate at 55°C	60% UCL Failure Rate at 55°C
0.3eV	$6.05 \times 10^5$	$3.66 \times 10^5$	1	$4.86 \times 10^7^*$	—	41	$7.45 \times 10^7$	—	27
0.6eV	$6.05 \times 10^5$	$3.66 \times 10^5$	0	$2.26 \times 10^7$	—	40	$5.30 \times 10^7$	—	17
1.0eV	$6.05 \times 10^5$	$3.66 \times 10^5$	0	$2.11 \times 10^8$	—	4	$8.75 \times 10^8$	—	1
<b>Total</b>					—	85		—	45

\*0.3eV equivalent hours includes voltage acceleration for 7.5eV stress.

Table XII: Long term failure rate (not including 48 hr data point).

of dynamic lifetest. (Note: all units going into other tests received this stress as a preconditioning.) The short term failure fraction, sometimes called infant mortality percentage, can be estimated from these data in Tables IIIA, IIIB. In cerdip, no failures were observed from 1700 units. In plastic, there were 2 failures in 5055 units or 396 ppm. If the data from all packages is combined, a single point estimate is 296 ppm.

These results show that Xicor NOVRAMs have attained failure rates comparable, if not better, to those reported by major suppliers of standard volatile memory products.<sup>18-20</sup>

## SUMMARY

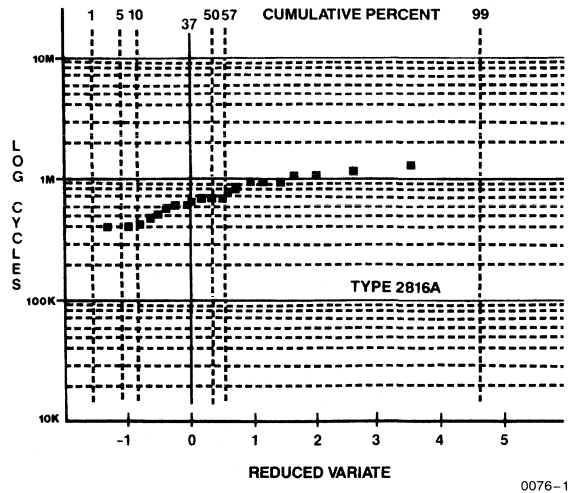
The data presented in this reliability report show that the data retention of Xicor's NOVRAM technology is excellent. Even at a high temperature (300°C), only about 2% lose data in 1000 hours. Theoretical grounds for expecting this result are discussed. Two calculations were done, one for short term (48 hours) failure rate and one for long term expected failure rate. These show an overall long term failure rate of 16 FIT at 55°C, 60% UCL and

an infant mortality of less than 300 ppm. The cerdip packaging employed is shown to be capable of passing the Group D qualification requirements of MIL-STD-883, Method 5005. Finally, the plastic packaging employed shows excellent 85°C/85% RH result.

## REFERENCES

1. R.H. Fowler and L. Nordheim, Proceedings of the Royal Society of London, A119, pp. 173-181 (1928).
2. M. Lenzlinger and E.H. Snow, Journal of Applied Physics, 40, pp. 278-283 (1969).
3. D.J. Di Maria and D.R. Kerr, Applied Physics Letters, 27, pp. 505-507 (1975).
4. R.M. Anderson and D.R. Kerr, Journal of Applied Physics, 48, pp. 4834-4836 (1977).
5. H.R. Huff et al, Journal of the Electrochemical Society, 127, pp. 2483-2488 (1980).
6. T.J. Lewis, Journal of Applied Physics, 26, pp. 1405-1410 (1955).

- 
7. C. Hu et al, Applied Physics Letters, 35, pp. 189–191 (1979).
  8. R.K. Ellis, IEEE Electron Device Letters, EDL-13, pp. 330–333 (1982).
  9. R.K. Ellis, H.A.R. Wegener, and J.M. Caywood, International Electron Devices Meeting Technical Digest, pp. 749–752 (1982).
  10. Z. Weinberg, Solid State Electronics, 20, pp. 11–18 (1977).
  11. G.L. Schnable and R.S. Keen Jr., IEEE Trans. on Electron Devices, ED16, pp. 322–332 (1969).
  12. S.R. Hofstein, Solid State Electronics, 10, pp. 657 (1967).
  13. J.R. Black, Proc. 6th Reliability Physics Symposium, pp. 148–153 (1967).
  14. R.E. Shiner et al, Proc. 18th Reliability Physics Symposium, pp. 238–243 (1980).
  15. Dwight L. Crook, 17th Annual Reliability Physics Symposium, pp. 1–7 (1979).
  16. B. Euzent et al, Proc. 19th Annual Reliability Physics Symposium, pp. 11–16 (1981).
  17. R.E. Shiner et al, Proc. 21st Annual Reliability Physics Symposium, pp. 248–256 (1983).
  18. Bruce Euzent, “2115/2125 N-Channel Silicon Gate MOS 1K Static RAMs” Intel Reliability Report RR-14, (1976).
  19. Chieh Lin Ping, “Reliability of N-Channel Metal Gate MOS/LSI Microcircuits” National Semiconductor, (1982).
  20. Bruce Euzent and Stuart Rosenberg, “HMOS Reliability” Intel Reliability Report RR-18, (1978).
  21. R.P. Merrett, J.P. Bryant, and R. Studd, Proc. 21st Annual Reliability Physics Symposium, pp. 73–81 (1983).
  22. K. Tsubosaki, et al, 21st Annual Reliability Physics Symposium, pp. 83–89 (1983).
- This report is based on data collected through February, 1985.



0076-1

# ENDURANCE OF XICOR E<sup>2</sup>PROMs AND NOVRAMs\*

By H.A. Richard Wegener

\*NOVRAM is Xicor's nonvolatile static RAM device.

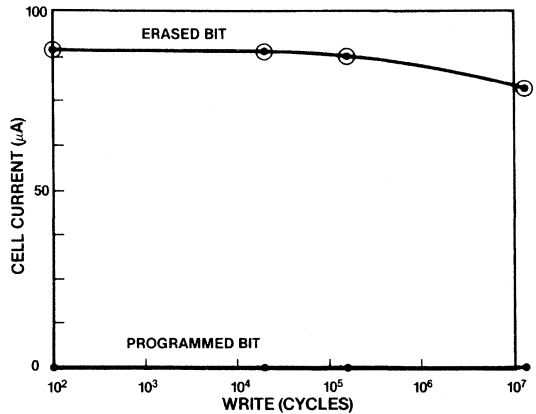
# INTRODUCTION

Endurance is a property unique to nonvolatile memories. It describes the ability of the nonvolatile memory section of the chip to sustain repeated data changes without failure. Such a data change occurs when a stored "1" is changed into a "0", or when a stored "0" is changed into a "1". Continual changes from "1" to "0" to "1" to "0" are called write-erase cycling, or just cycling.

In this work, endurance will first be defined. A quantitative method for characterizing endurance is described and applied to the characterization of endurance as a function of temperature and time between store events. Data on the endurance of a selection of Xicor's products is presented. Finally, the application of this information to the calculation of system failure rates is described. A general problem in discussions of endurance is that various people mean different things when they speak of endurance. One meaning which has been used is that endurance is the number of nonvolatile data changes to a "typical" cell before the cell dielectric fails or the programming window closes. Figure 1 shows such data for a typical Xicor E<sup>2</sup>PROM cell showing that after greater than 10<sup>7</sup> data changes the cell still has good margin with respect to the 50  $\mu$ A trip point of our sense amplifier. Many other suppliers have presented similar data. Unfortunately this data is of little help to the user who doesn't buy one "typical" cell, but rather an array containing a large number of cells, some of which will not be typical.

Xicor's definition of the endurance of an individual memory is that the limit of endurance is reached when, under conditions specified by the data sheet for normal operation, the first bit on any chip is found to be in error after a required data change. This limit of endurance, or endurance for short, is expressed in terms of cycles. By this definition then, endurance (in cycles) is the number of data changes per bit that occurred without error before the first failure took place.

When a nonvolatile memory chip is operating within a given application, it can be expected that some bits on that chip will experience more data changes than other bits, unless particular attention



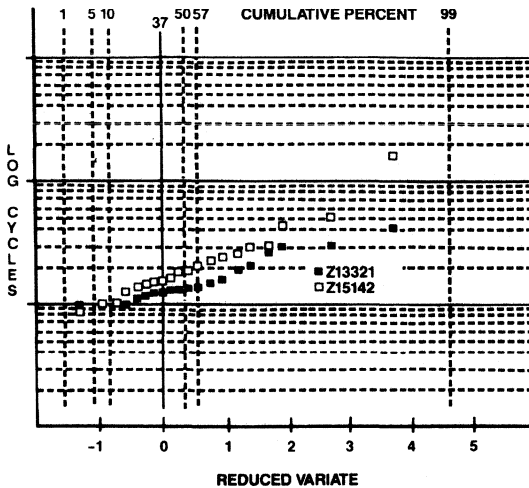
0076-2  
Figure 1: E<sup>2</sup>PROM cell current vs. write/erase cycles. 50  $\mu$ A is the trip point of the cell.

has been paid to even out their use throughout the chip. Within a given chip the endurance of individual bits have a small range of values, and it is pure chance whether a highly cycled bit has an endurance on the high end or the low end of that distribution.

Xicor's approach to this problem is that the lowest, the worst case endurance on any given cell in the array, defines the endurance of that chip. In order to test for the bit that causes the worst case endurance, each bit on that chip must be subjected to the same number of data changes during cycling. When the first bit on that chip fails, all other bits have been cycled without failure at least the same number of times. While these other bits may have much higher endurance limits, the endurance of the chip under test is defined as that of the one worst case bit.

Knowledge of the statistical distribution of the worst case bit from each of thousands of devices makes the endurance of a given chip statistically predictable. We have found that our endurance data fit a known statistical distribution — it is the logarithmic "Extreme Value" distribution. Its properties, and the handling of cycling data to derive its parameters for a given lot, are described in Appendix A.

# The Measurement of Endurance

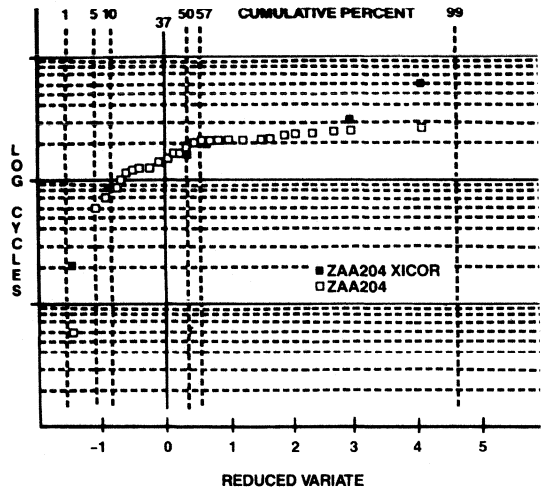


0076-3

Figure 2: Typical endurance plots of two lots of Xicor X2212 NOVRAMs. The upper horizontal axis gives the cumulative percent of failures.

The graph in Figure 2 shows the plots of endurance of two different lots of Xicor's X2212 NOVRAMs. This graph is an example of endurance plotted using an extreme value distribution. The meaning of the lower horizontal axis, the linear extreme value variate, is explained in Appendix A. The upper horizontal axis, however, has intuitive appeal. It is the cumulative failure percentage. The plots are well distributed around a straight line. This indicates that they originate from an Extreme Value distribution. They differ somewhat in slope (which is the measure of spread, or dispersion of the distribution). They are also offset in the vertical direction, which indicates that the maximum of each distribution is different. Since the cycles are plotted as their logarithms, this difference is about 40%.

Implicit in this discussion is the assumption that the endurance performance of lots can be described as the result of a relatively small sample. This has been proven correct experimentally and has been used to establish correlation between different pieces of equipment used for the determination of endurance. A successful application of this is shown in Figure 3.



0076-4

Figure 3: Correlation between endurance data obtained by Xicor and by one of Xicor's customers for Lot ZAA204. Each test is based on 28 data points. Most of Xicor's points are coincident with the customer's so that they are hidden.

The graph in Figure 3 shows the outcome of an endurance correlation exercise between Xicor and one of its customers. The first set of points (black squares) was established from a 30-device sample of X2212s from lot ZAA204 cycled out at Xicor. Overlying most of these original points are a second set (open squares) which were generated by endurance measurements on a separate 30-device sample from the same lot at the facility of the customer. It can be seen that the signatures of the two samples match faithfully, except at both extremes. At the left hand side, the difference can be explained by the increased scatter of any distribution at its extremes. At the right hand side, a slight difference was introduced when the customer stopped cycling before the last three devices had failed. Even if it is assumed that the match would not have improved by further cycling, the agreement for 27 out of 30 points, or between 5% and 95% of the sample, is excellent.

---

## ENDURANCE VARIABLES

The existence of an inherent limit to endurance is a universal property of nonvolatile semiconductor memories. Regardless of the materials used and of the details of the cell design or the semiconductor manufacturer, there is a measurable upper limit to the number of data changes that such a memory cell can sustain and still meet the data retention specification. The exact number of cycles, however, is dependent on all the elements that go into the construction and operation of a given cell design.

The reason for an endurance limit arises from the basic physics of nonvolatile semiconductor memories. All such memories depend on the highly nonlinear conduction properties of the solid-state dielectrics employed to form the memory cells. At high electric fields, these dielectrics permit a predictable current to pass from one electrode to another. This is used to program or erase such a device. At low electric fields, essentially no electron is transmitted. Therefore charges transferred at high fields to locations isolated by this type of dielectric will remain there indefinitely. But during the transfer of charge at high fields, a very small fraction of the electrons passing through becomes trapped in the dielectric. The many thousands of times that this happens during the life of a memory contribute more and more trapped charge, creating an electric retarding potential in the dielectric, until the device cannot function as a memory any more. Then its endurance limit is reached.

The nonvolatile cells used in Xicor memories make use of the special characteristics of its microtextured surface. The many tiny regions of gently curved features are particularly effective as non-linear conduction elements. As a result of the combination of surface curvature and thick oxide, they require relatively low voltages for programming, and provide excellent retention of data. The physics of the programming process as well as the excellent data retention measured for Xicor memories have been described in a recent publication.<sup>1</sup>

If all these features were identical, if the thickness of the dielectric over them were the same, and if the details of the high voltage generator on the chip were precisely reproducible, then every device on the same silicon wafer, and in the same manufacturing lot would have identical endurance limits. In the real world, there are small variations in the results of the intricate fabrication steps of the silicon chip. These give rise to a range of endurance values for all the nonvolatile memory cells on the same chip.

Additional small variations will occur from chip to chip over the whole silicon wafer, and from wafer to wafer. All of these define the details of the distribution that describes the endurances of all the memory cells in a device lot. Once the chips have been fabricated, the average and the dispersion of this distribution have been fixed by the interaction of cell design and the fabrication process with its small variations. These are the fixed internal parameters of endurance. The dispersion is an indicator of the process variation.

There are, however, variations that can be superimposed on the fixed characteristics by the conditions that accompany the normal use of the nonvolatile memory devices. The temperature of operation is one of these. Both the details of the charge transfer process in the nonvolatile memory cell, and the operation of the high voltage generating circuit should be affected in some way by this condition. Another externally controlled parameter is the frequency of the cycling process. At the end of a storage cycle the newly trapped electrons are in a relatively high free energy state. Longer periods between cycles give these charges and their environment more time to relax into a lower energy state. This should also affect the measured endurance parameters.

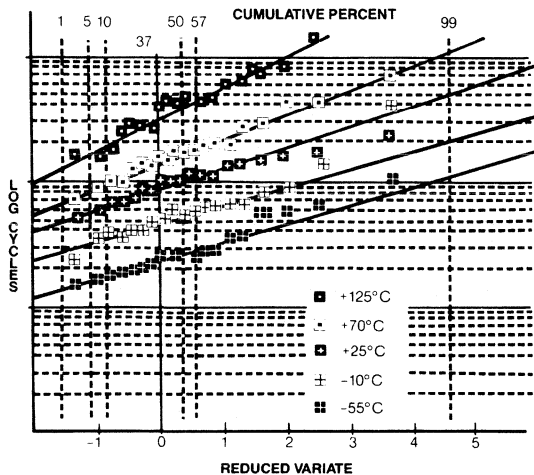
The control of these external parameters is essential when exact correlation of endurance data must be obtained. Their knowledge is also important to optimize performance and predict reliability in any application.

## The Effect of Temperature on Endurance

The endurance of a lot of nonvolatile memories can be described concisely by the constants defining its statistical distribution. For the simple "Extreme Value" distribution pertinent here, these constants are its mode and its dispersion. This distribution can be used to assist in the characterization of endurance.

Five 20-device samples from the same lot of X2212 NOVRAMs were subjected to continuous data changes, each at a different temperature, until all devices had failed. The temperature levels were  $-55^{\circ}\text{C}$ ,  $-10^{\circ}\text{C}$ ,  $+25^{\circ}\text{C}$ ,  $+70^{\circ}\text{C}$ , and  $+125^{\circ}\text{C}$ . The delay between data changes for all devices was one second. The endurances of individual devices were plotted in the form of a probability plot, as shown in Figure 4.

<sup>1</sup>XICOR Reliability Report RR-502A.



0076-5

Figure 4: The effect of temperature on endurance: the endurance doubles for every increase in temperature by 50°C.

The y-axis gives the logarithm of the number of cycles that each unit had at the end of its endurance. The straight lines shown were least-squares fitted to each set of data. The correlation coefficients for lines ranged from 97% to 99%. The results can be summarized as follows:

- 1) There is an increase in the endurance with increasing temperature.
- 2) The dispersion is essentially constant at and below room temperature and increases somewhat above room temperature.

Over the range of the data, the logarithm of the endurance is linearly related with temperature. The coefficient is 0.0062/°C, but as a simple rule, the endurance doubles for every increase of temperature by 50°C.

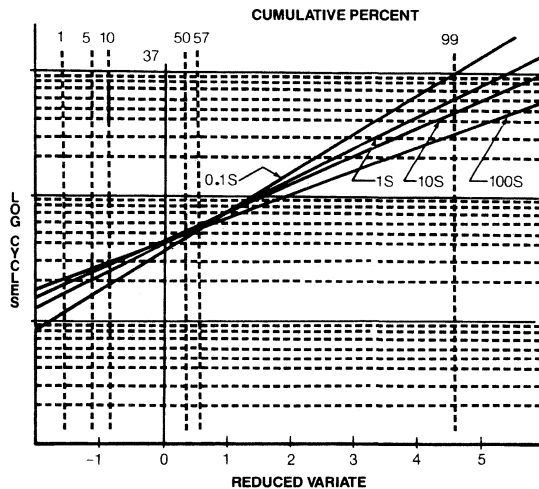
## The Effect of Data Change Delay on Endurance

The baseline values of endurance can also be modified by the length of the delay between consecutive data changes.

In the determination of the endurance of a lot there is a premium on getting the job done as rapidly as possible. This means that only minimum delays can be added between STORE signals. Typically, the devices in a lot of our current NOVRAMs have endurance between 10,000 and 100,000 cycles.

The time to cycle a lot of devices will be 3 hours if the last device to fail had an endurance as low as 100,000 cycles for delays between data changes of 0.1 second even if all devices are cycled in parallel. This total cycling time increases to 28 hours for a delay of 1 second, to 12 days for a delay of 10 seconds, and 120 days for a delay of 100 seconds. Even a 1000 second delay is at the low end of the type of write frequency to be expected in most applications, and this would take in excess of three years to document. For this reason we have limited the experimental work on the effect on lot endurance to delays of 0.1, 1, 10, and 100 seconds. The shortest delay could not be reduced much below 100 ms, since that is the time required by the micro-processor which was used in the test to handle addressing, reading and recording data of the many devices tested simultaneously.

Four 20-device samples were taken from the same lot of X2212 NOVRAMs and then they were cycled until all devices had failed. The endurance of each device was recorded. Each of the four samples had one of the four different data change delays in its cycling program. The data are summarized in Figure 5. Individual data points were not recorded on this graph, since there was much confusing overlap where the data point from the samples overlay each other. Instead, the points were replaced with least-squares fitted straight lines. The correlation coefficients for these lines were between 97 and 99%.



0076-6

Figure 5: The effect of data change delay on endurance: the maximum of the distribution is unchanged, but it becomes tighter as the delay increases.

The results can be best expressed in terms of the constants of the distributions obtained:

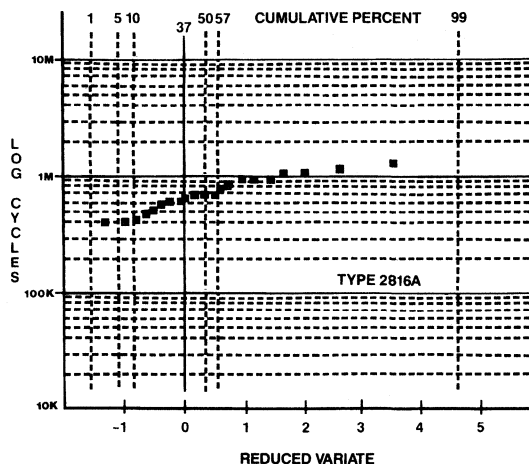
- 1) The mode of the distribution did not change for the four orders of magnitude of delay tested. This is shown by the fact that the individual lines cross near 37% of the cumulative frequency.
- 2) The slope of the distribution decreased 15% per decade of cycles with each order of increase in delay. At first sight, this might appear to be a small change. But in the terms of the definition of endurance, they are quite important for many applications. This is because the endurance change in the region where the majority of the units have failed is irrelevant. The important region is that in which only a few per cent or less have failed. In this region, the effect of the longer time between store events at a constant endurance level is to decrease the fraction failing by an order of magnitude or more!

## Endurance Status of XICOR Memories

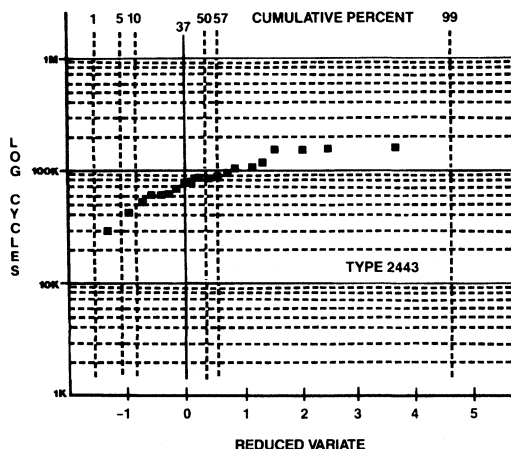
Figure 4 and 5 lack vertical scales because they are intended to show general tendencies. The actual endurance observed on Xicor memories vary from product to product because of differences in cell design and to a lesser amount from lot to lot because of small processing variations. There is also a general tendency for the endurance to improve with time as a result of refinements in design and processing technique.

To give the user a sense of the status of endurance of Xicor memories as of the date of this report, distribution measurements for several product types are reported here. All of this data measured at 25°C and rapid cycling rates. Figure 6 shows the endurance data measured on a lot of X2816As. The process average for this lot is about 500,000 cycles with the 5% point on the curve appearing at 200,000 cycles. In Figure 7 the measured endurance distribution of a lot of X2443s (a 256 bit serial NOVRAM) is displayed. For this device the process average was ~ 80,000 cycles and the 5% point appears at 30,000 cycles. The measured endurance distribution of a lot of X2212s is shown in Figure 8. This product exhibits a process average of about 100,000 cycles and the 5% point appears at 40,000 cycles.

The data reported here are intended as a status report. As we further refine our products and increase the endurance, we intend to issue updates to this report.

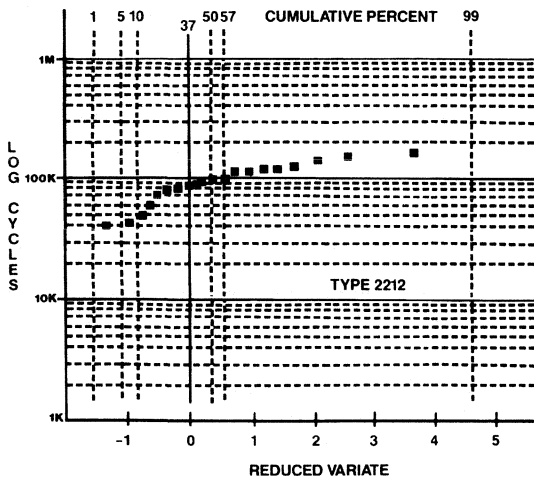


0076-1  
Figure 6: Endurance data from a lot of Xicor X2816A E2PROMs.



0076-7  
Figure 7: Endurance data from a lot of Xicor X2443 Serial NOVRAMs.





0076-8

Figure 8: Endurance data from a lot of Xicor X2212 NOVRAMs.

## QUALITY ASSURANCE APPLICATIONS

One problem any supplier of nonvolatile memory faces is how to define endurance and how to assure that the parts reaching the customer actually satisfy the endurance specification. This task is akin to assuring the lifetime of a light bulb. If the light bulb is specified to have a 1000 hour life, one can verify that the bulb lasts 1000 hours by burning it for that period. However, one now knows only that the bulb lasted 1000 hours, not that it will last another 1000 hours. The statistical technique discussed in this report allows Xicor to perform this difficult and exacting task. What a Xicor endurance specification means is that for any lot of memories shipped, fewer than 5% of the units will cease to cycle before the specified limit when cycled at room temperature and at the maximum frequency allowed by the specification. Xicor continually samples production lots to assure that this criterion is met.

Let's look at what this means in a typical application. Assume that the Xicor memory is used in an electronic system which contains a number of other components so that the average chip temperature is 50°C and that the average delay between store

events is some minutes. Examination of Figure 3 shows that raising the chip temperature from 25°C to 50°C would decrease the fraction of units not exceeding the endurance value from 5% to 0.03%. For data change delays of 100 seconds and longer, the fraction of the lot not meeting the nominal endurance value further decreases to 0.001% or less.

Of course, in a given application the predicted behavior may be better or worse than that worked out in the previous example. However, the information supplied here should be sufficient for the user to compute the expected endurance failure rate in a particular application.

One last consideration is how endurance failures affect the overall device failure rate. Here again, the calculation is a little application-sensitive, but for simplicity assume that the system is designed to last  $10^5$  hours ( $\sim 12$  years) and that the device performs nonvolatile writes roughly uniformly over this period. If the application is designed to use the specified number of cycles over the life of the part, the additional endurance-related failure rate is the cumulative failed fraction divided by the time. For our previous example, this works out to 0.001%/ $10^5$  hours or  $10^{-5}\%/1000$  hours (0.1 FIT). As this illustrates, in most well-designed systems the endurance-related failures of Xicor products do not significantly increase the overall device failure rate.

In all discussions of endurance in this work NOVRAMs and E<sup>2</sup>PROMs have been treated as if they behave the same. From a physical view of the nonvolatile storage element this is correct. However, there are two properties of the NOVRAM cell which may cause it to have significantly enhanced endurance in certain applications. One factor is that the NOVRAM allows the user to store data in the volatile latch during normal operation and only transfer data to the nonvolatile element prior to power down. In applications which require a high frequency of data changes but only relatively infrequent power interruptions this may be very useful. A second, if less obvious factor, is that unlike the E<sup>2</sup>PROMs which automatically erase each byte prior to each write, the NOVRAMs only transfer electrons in the case of a change in nonvolatile data. This means that only those cells in which nonvolatile data is altered use up endurance. In some applications this fact can be used to greatly increase effective endurance of the memory.

## SUMMARY

A method of characterizing endurance which is of general applicability has been described here. This method has been applied to the characterization of endurance as a function of temperature and time between store events. The meaning of Xicor's endurance specification is defined in the framework of this method. Based on the above, the fraction of Xicor product which is predicted to fail to store prior to attaining the specified endurance is predicted to be less than 0.001% in a typical system in which the devices experience a 50°C ambient temperature.

## APPENDIX A

### The Mathematics of Endurance Characterization

The mathematical characterization of endurance data arises most elegantly from the definition of endurance. In an individual device, the endurance is the minimum number of data changes that all memory cells can sustain until one cell gives rise to an erroneous output (due to a permanent change in its characteristics). The extreme characteristic from a fixed set of possible values forms a well-known distribution called the Extreme Value distribution. This distribution is independent of the distribution within that fixed set of values. Since by definition, the endurance of a chip containing 1024 memory cells is that of the cell with the minimum endurance, it can be expected that the endurances of the chips from the same device type will have the Extreme value distribution.

The formulations of the Extreme Value distribution are given in Table I. On the left hand side are the entries for the Extreme Value distribution, and

on the right hand side the corresponding entries for the Normal distribution.

The cumulative probability  $\Phi$  is defined by a fraction of 1. It defines, towards one side of a distribution, the fraction of the population  $\Phi$  that has a smaller value than the variate at that fraction, and towards the other side, the complement of that fraction which has a larger value than the variate at that fraction. This is quite often expressed as "fraction with more than ..." or "fraction with less than ...". It can be seen that the cumulative probability of the Extreme Value distribution  $\Phi_{EV}$  has a much simpler functional relationship with its variate  $Y$  than the equivalent  $\Phi_N$  with its variate  $Z$  of the Normal distribution. The Extreme Value variate  $Y$  is related by two constants to the distributed property  $X$ . One constant is the maximum of the distribution  $U$ , and the other the dispersion  $1/\alpha$ . The Extreme Value distribution is not symmetrical around its maximum (as the Normal distribution is). Instead, one side is stretched out more than the other. If the low cumulative probability fraction is on the narrower end, the maximum of that distribution is located at the value of 0.366, or 37%.

This is typical of the distributions of low extremes, and this is the distribution used for endurance values from NOVRAM chips of the same device type. There is one more empirical observation: it is not the number of cycles, but the logarithm of the number of cycles that has the form of the Extreme Value distribution. The  $X$  in the expression for the variate then is the logarithm of the observed cycles of individual chip endurances,  $\alpha$  is the dispersion of the distribution of these endurances, and  $U$  is the observed or interpolated value of the log of the endurance at  $\Phi = 0.366$ .

The extraction of these two constants from the data could be a complex calculational procedure, but by linearizing the variate  $Y$ , it becomes as simple as plotting a straight line. The approach is summarized in Table II.

Statistic	Extreme Value	Normal Distribution
Cumulative Probability	$\Phi_{EV} = \text{EXP}(-\text{EXP}(-Y))$	$\Phi_N = \int_{-\infty}^Z (2)^{-1/2} \text{EXP}(-T^2/2) dT$
Variate	$Y = \alpha(X - U)$	$Z = (X - M)/\sigma$
Maximum	$U$ at $\Phi = 0.37$	$M$ at $\Phi = 0.50$
Dispersion	$1/\alpha$	$\sigma$

Table I: Mathematical definitions.

$\Phi_i = \text{EXP}(-\text{EXP}-Y_i)$ $Y_i = \alpha(X_i - U)$ $= -\text{LN}(-\text{LN}\Phi_i)$
$X_i = U + (1/\alpha)(-\text{LN}(-\text{LN}\Phi_i))$ <p>BUT <math>X_i = \text{LOG} CY_i</math></p> $U = \text{LOG} CY_m$
$\text{LOG} CY_i = \text{LOG} CY_m + (1/\alpha)(LV)$ <p><math>CY_i =</math> endurance of part<sub>i</sub></p> <p><math>CY_m =</math> maximum of distribution</p> <p><math>(1/\alpha) =</math> slope of line</p> <p><math>(LV) = (-\text{LN}(-\text{LN}\Phi_i))</math></p>

Table II: Linearized plot.

The first line states once more the cumulative probability relationship between  $\Phi$  and  $Y$ , and the second line the linear relationship between  $Y$  and  $X$ . The third line shows that the value of  $Y$  can be calculated from the double natural logarithm of  $\Phi$ . The fourth line expresses the second line as a function of  $X$ , and substitutes its functional relationship with  $\Phi$ . Identification of  $X$  with the logarithm of an individual observation, and  $U$  with the logarithm of the maximum of the distribution of cycles then leads to the seventh line which states the desired linear relationship. A typical plot is shown in Figure 9. There is clearly a straight line relationship. The value of the maximum occurs at  $\Phi = 37\%$ , and the slope of the line is the value of  $1/\alpha$ .

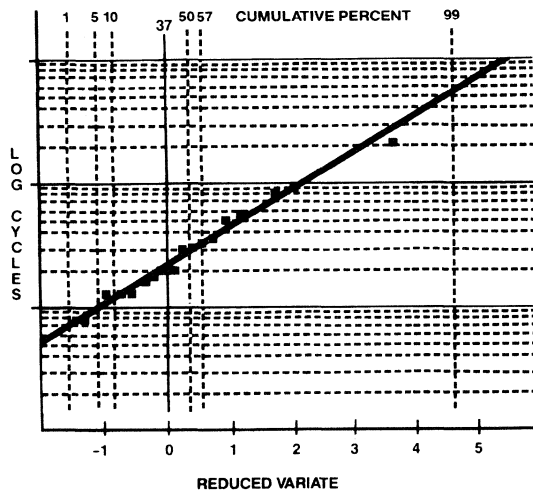


Figure 9: Straight line plot of the logarithm of endurance cycles vs. the reduced variate.

0076-9

There remains one more problem, and that is how to associate the correct value of  $\Phi$  with a given observed endurance. This is accomplished by taking all the endurance from a group of devices and writing them down in the order of increasing cycles (this is called "ranking"). Looking at the data in this way, any given endurance represents the borderline between a fraction of the lot that is higher than anything preceding it, and lower than anything following it. The approximate value of that fraction is found by assigning consecutive rank numbers to the ordered endurance: 1 to the lowest, 2 to the second lowest, and so on, until the highest endurance ends up with the rank equal to the total number of devices tested in that group. Dividing the rank numbers by the total number of the devices in the group then yields the "fraction lower than . . .". A slightly more exact value for  $\Phi$  is found by the formula  $\Phi = (i - 1/2)/N$ , where  $i$  is the rank number and  $N$  the total number of devices tested.

Raw Data (CY)	Ranked Data (CY <sub>i</sub> )	Rank (i)	Plotting Position ( $\Phi_i = (i - 0.5)/n$ )
129.50	7.31	1	0.025
35.95	12.10	2	0.075
21.95	12.10	3	0.125
7.31	12.10	4	0.175
31.95	16.85	5	0.225
19.65	19.65	6	0.275
60.75	21.95	7	0.325
33.95	22.45	8	0.375
22.45	22.95	9	0.425
85.75	31.45	10	0.475
12.10	31.95	11	0.525
22.95	33.95	12	0.575
12.10	35.95	13	0.625
79.25	48.25	14	0.675
52.75	52.75	15	0.725
209.50	60.75	16	0.775
16.85	79.75	17	0.825
12.10	85.75	18	0.875
48.25	129.50	19	0.925
31.45	290.50	20	0.975

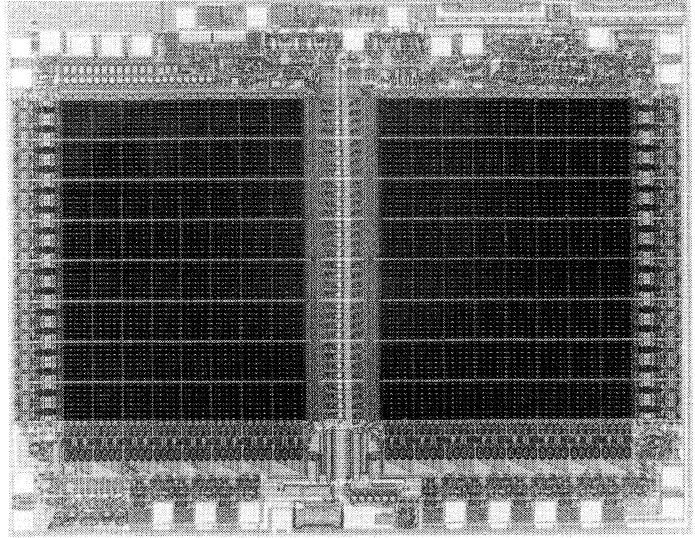
PLOT LOG (CY<sub>i</sub>) vs.  $-\text{LN}(-\text{LN}\Phi_i)$

Table III: Data preparation.

This report is based on data collected through February, 1984.

---

## NOTES



0077-1

# **X2816A/X2804A RELIABILITY REPORT**

**By Reliability Engineering Staff**

# INTRODUCTION

The X2804A and X2816A are electrically erasable programmable read only memories (E<sup>2</sup>PROMs) organized 512 x 8 and 2K x 8 respectively. These memories operate on a single 5V power supply for all operations. Figure 1 provides pinouts for the two parts; Figure 2 shows the functional block diagram for the X2816A; Figures 3 and 4 illustrate the physical location of the various address bits. The thermal resistance table, burn-in circuit and a timing diagram are included in Appendix A for your reference.

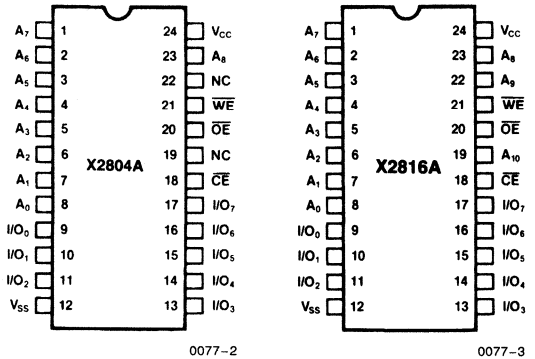


Figure 1: X2804A and X2816A Pin configurations.

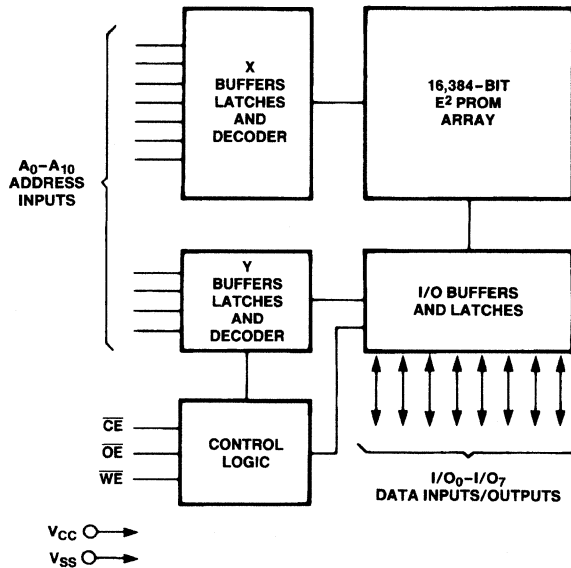
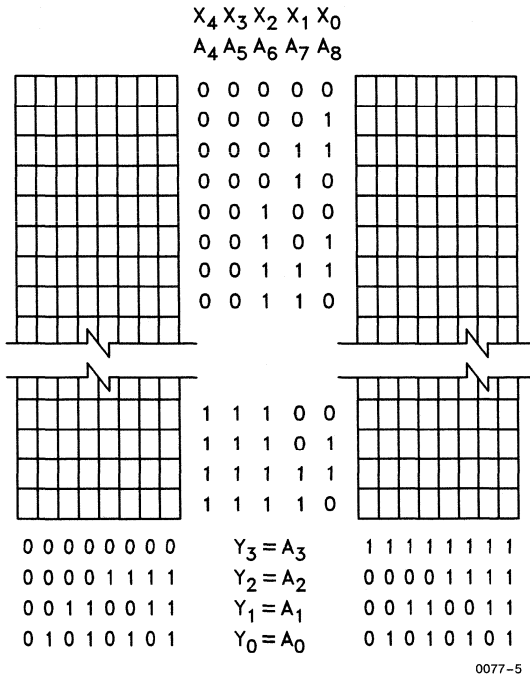


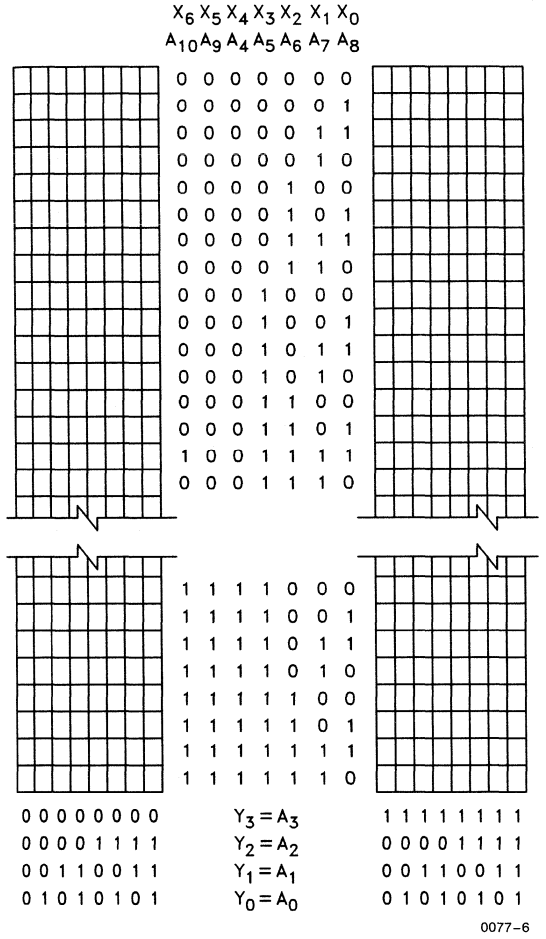
Figure 2: X2816A Functional block diagram.



Each square equals one byte.

Figure 3: X2804A Physical bit map.

0077-5



Each square equals one byte.

Figure 4: X2816A Physical bit map.

0077-6

---

## TECHNOLOGY

Xicor E<sup>2</sup>PROMs are manufactured using a triple polysilicon N-channel process. Data is stored as the presence of positive or negative charge on the second level polysilicon which acts as a gate to a sense transistor. This second level polysilicon is a floating gate surrounded by  $\sim 750\text{\AA}$  of thermally grown oxide. Charge is transferred to and from the floating gate through a quantum mechanical effect known as Fowler-Nordheim tunneling. This phenomenon has been described in detail in recent Xicor publications.<sup>1,2,3</sup>

Xicor's process employs a textured polysilicon. This creates a textured surface between the polysilicon and the tunneling oxides, resulting in a sharp decrease in tunneling current with a decrease in voltage allowing the use of thick tunneling oxides. This in turn results in lower leakage currents from the floating gate during static store periods and during read operations. Recent Xicor publications describe the excellent data retention that can be expected from this technology.<sup>3</sup> For both the X2804A and X2816A Xicor specifies a data retention of 100 years.

## RELIABILITY STUDY AND RESULTS

This report is based on data collected using the X2816A. The X2804A is a smaller version of the X2816A, produced by using the design of the X2816A with three-quarters of the array and two address buffers removed. Thus, reliability studies were focused on the X2816A. The X2816A has four times the memory and approximately twice the active silicon area; therefore, it is the more sensitive reliability indicator.

Before Xicor qualifies any new product it is subjected to a series of accelerating stresses and tests. These tests are designed to accelerate any degradation a device may experience over the course of a normal lifetime in order to uncover any design or process flaws. Because package type has an affect on device reliability, complete qualification of the X2816A involved both plastic and cerdip units. In addition, Xicor runs ongoing monitors of those products in production. This assures high reliability standards for all product shipped by Xicor.

The stresses used to establish reliability data are as follows:

- 1) High temperature dynamic lifetest.
- 2) Data retention bake.

- 3) High temperature high voltage stress.

- 4) Environmental testing.

A short description of these tests and the results obtained are presented in the following report.

## Dynamic Lifetest

Failure modes typically encountered in MOS semiconductor devices can be accelerated if the device is operated at elevated temperatures. The dynamic lifetest aims to accelerate any failure modes a device may exhibit by operating the device in its most common mode at high temperature.

For the X2816A, the dynamic lifetest consisted of continually reading a known data pattern stored in the device, while it was subjected to a temperature of  $+125^{\circ}\text{C}$ . Each unit was then tested for data retention and complete functionality after 168, 500, 1000 and 2000 hours of dynamic lifetest. The results of the tests are shown in Table I.

## Data Retention Bake

The purpose of this stress is to measure and ensure a device's ability to retain correct data. Technologies using floating gate structures to retain charge will all have a greater tendency to loose this charge at higher temperatures.

This test is conducted by storing a checkerboard pattern in the devices under test and then baking the devices at  $+150^{\circ}\text{C}$  for plastic units and at  $+250^{\circ}\text{C}$  for cerdip units. The pattern is verified after 48, 168, 500, 1000 and 2000 hours of bake. In most cases a group is split and retention evaluated on units that have been precycled (10,000 erase/write cycles) and units that have not been cycled. This provides a base to study the affect (if any) of writing to an E<sup>2</sup>PROM on data retention. The results of the tests are shown in Tables II and III.

## High Temperature High Voltage Stress

The high temperature high voltage test is a derivative of the high temperature reverse bias test used to evaluate bipolar circuits. In this test  $V_{SS}$  is grounded while all inputs and  $V_{CC}$  are maintained at high voltage while being baked. The stress is intended to expose failures due to mobile ionic contaminants, electrical overstress and latent gate oxide defects.



Lot #	168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1C	0	159	0	84	0	84	0	84	$1.8 \times 10^5$
2C	0	152	0	93	0	93	1[a]	93	$2.0 \times 10^5$
3C	0	75	0	75	0	75	0	75	$1.5 \times 10^5$
4C	0	388	0	99	1[a]	99	0	98	$2.5 \times 10^5$
5C	1[a]	387	0	126	0	126	0	—	$1.7 \times 10^5$
1P	1[b]	410	0	51	0	51	0	51	$1.6 \times 10^5$
2P	0	389	0	76	0	76	0	76	$2.0 \times 10^5$
3P	0	214	0	15	0	15	0	15	$6.3 \times 10^4$
<b>Totals</b>	<b>2</b>	<b>2174</b>	<b>0</b>	<b>619</b>	<b>1</b>	<b>619</b>	<b>1</b>	<b>492</b>	<b><math>1.4 \times 10^6</math></b>

[a] Ionic contamination: 1eV

[b] Retention failure: 0.6eV

Note: C = Cerdip

P = Plastic

Table I: 125°C Dynamic lifetests results.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	50	0	50	0	50	0	50	0	50	$1.0 \times 10^5$
2*	0	24	0	24	0	24	0	24	0	24	$4.8 \times 10^4$
3	0	20	0	20	0	20	0	20	0	20	$4.0 \times 10^4$
4*	0	55	0	55	0	55	0	55	0	55	$1.1 \times 10^5$
<b>Totals</b>	<b>0</b>	<b>149</b>	<b>0</b>	<b>149</b>	<b>0</b>	<b>149</b>	<b>0</b>	<b>149</b>	<b>0</b>	<b>149</b>	<b><math>3.0 \times 10^5</math></b>

\*Denotes units that received 10,000 erase/write cycles prior to retention tests.

Table II: 250°C Cerdip unit, retention bake test results.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	51	0	51	0	51	0	51	0	51	$1.0 \times 10^5$
2	0	25	1[a]	25	0	24	0	24	0	24	$4.8 \times 10^4$
3*	0	76	0	76	0	76	0	76	0	76	$1.5 \times 10^5$
<b>Totals</b>	<b>0</b>	<b>152</b>	<b>0</b>	<b>152</b>	<b>0</b>	<b>151</b>	<b>0</b>	<b>151</b>	<b>0</b>	<b>151</b>	<b><math>3.0 \times 10^5</math></b>

[a] Data retention failure: 0.6eV

\*Denotes units that received 10,000 erase write/cycles prior to retention test.

Table III: 150°C Plastic unit retention bake test results.



This test was conducted on the X2816A at 5.5V and +150°C. Data retention and functionality were verified after 48, 168, 500, 1000 and 2000 hours. The results of the test are shown in Table IV.

ments. Due to the inherent differences between plastic and cerdip devices, different reliability stresses are applied to evaluate the individual package.

## ENVIRONMENTAL TESTING

Environmental tests are designed to determine a device's resistance to extreme or changing environ-

## Cerdip

The standard tests for cerdip encapsulated devices are defined by MIL-STD-883, Method 5005, Group C and D. The results and conditions of these tests on typical Xicor products are listed in Tables V and VI.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1C	0	25	0	25	0	25	0	25	0	25	$5.0 \times 10^4$
2C	0	25	0	25	0	25	0	25	0	25	$5.0 \times 10^4$
3C	0	51	0	51	0	51	0	51	0	51	$1.0 \times 10^5$
4C	0	25	0	25	0	25	0	25	0	25	$5.0 \times 10^4$
1P	0	52	0	52	1[a]	52	0	51	0	51	$1.0 \times 10^5$
2P	0	51	0	51	0	51	0	51	0	51	$1.0 \times 10^5$
3P	0	15	0	14	0	13	0	13	2[a]	13	$2.7 \times 10^4$
<b>Totals</b>	0	244	0	243	1	242	0	241	2	241	$4.8 \times 10^5$

[a] Oxide breakdown: 0.3eV

Note: C = Cerdip  
P = Plastic

Table IV: High temperature high voltage stress test results.

Test	883 Test Method	Conditions	LTPD	Accept #	Results
Temperature Cycling	1010	Test Condition C (10 cycles -65°C to +125°C)	15	0/15	0/34
Constant Acceleration	2001	Test Condition E (30,000g Y1 axis)	15	0/15	0/34
Seal	1014		15	0/15	
Fine		Test Condition B			0/34
Gross		Test Condition C			0/34

Table V: Group C, die related tests.

Test	883 Test Method	Conditions	LTPD	Accept #	Results
Lead Integrity	2004	Test Condition B2	15	0/15	0/15
Seal	1014		15	0/15	
Fine		Test Condition B			0/15
Gross		Test Condition C			0/15
Thermal Shock	1011	Test Condition B (15 cycles –55°C to +125°C)	15	0/15	0/34
Temperature Cycle	1010	Test Condition C (10 cycles –65°C to +125°C)	15	0/15	0/34
Moisture Resistance	1004		15	0/15	0/34
Seal	1014		15	0/15	
Fine		Test Condition B			0/34
Gross		Test Condition C			0/34
Mechanical Shock	2002	Test Condition B (1500g peak 3 axis)	15	0/15	0/34
Variable Frequency Vibration	2007	Test Condition A (29g peak 3 axis)	15	0/15	0/34
Constant Acceleration	2001	Test Condition E	15	0/15	0/34
Seal	1014		15	0/15	
Fine		Test Condition B			0/34
Gross		Test Condition C			0/34
Salt Atmosphere	1009	Test Condition A	15	0/15	0/43
Seal	1014		15	0/15	
Fine		Test Condition B			0/43
Gross		Test Condition C			0/42
Internal Water Vapor	1018	5,000 ppm Max. Water Content at 100°C	—	0/3 or 1/5	0/5
Adhesion of Lead Finish	2025		15	0/15	0/15
Lid Torque	2024		—	0/5	0/5

Table VI: Group D, package related tests.

## Plastic

Some of the tests used to evaluate cerdip packages do not apply to plastic packages. Tests such as seal, internal water vapor content and lid torque do not apply because plastic packages are not hermetically sealed and do not have lids. Other tests such as vibration and acceleration do not apply because the die in plastic packages are completely embedded in plastic and are not susceptible to such mechanical failures. Plastic packages, however, may be more susceptible to other failure modes. Due to the considerable difference in expansion coefficients between plastic and silicon, plastic devices may be more susceptible to temperature cycling failures. Plastic package devices may also be more susceptible to moisture. Therefore, the plastic units were subjected in greater numbers to more stringent tests.

## Temperature Cycling

Plastic packaged devices were subjected to 1000 temperature cycles per MIL-STD-883 Method 1010 Condition C. The results of this test are shown in Table VII.

Lot #	168 Cycles		500 Cycles		1000 Cycles	
	# Fail	# In	# Fail	# In	# Fail	# In
1	0	57	0	57	0	57
2	0	59	0	59	0	59
3	0	30	0	30	0	30
<b>Totals</b>	0	146	0	146	0	146

Table VII: Temperature cycling test results.

## 85°C/85% Relative Humidity and Autoclave Tests

Because plastic encapsulated devices may be more susceptible to moisture related failures they are subjected to environmental tests at 85°C with 85% relative humidity (both powered-on and powered-off). Three additional sample lots were subjected to autoclave tests (pressure pot) at two atmospheres. These stresses test for corrosion, electrolytic failure modes and passivation integrity. The results of these tests are presented in Tables VIII, VIII B and IX.

85/85 V <sub>CC</sub> = + 5.5V							
Lot #	168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	52	0	52	0	52	5.2 × 10 <sup>4</sup>
2	0	52	0	51	0	49	5.0 × 10 <sup>4</sup>
3	0	15	0	15	0	15	1.5 × 10 <sup>4</sup>
<b>Totals</b>	0	119	0	118	0	116	1.2 × 10 <sup>5</sup>

Table VIII A: 85/85 Test results, V<sub>CC</sub> = + 5.5V.

85/85 V <sub>CC</sub> = 0V							
Lot #	168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	52	0	52	0	47	5.0 × 10 <sup>4</sup>
2	0	52	0	51	0	47	4.9 × 10 <sup>4</sup>
3	0	15	0	15	0	15	1.5 × 10 <sup>4</sup>
<b>Totals</b>	0	146	0	146	0	146	1.1 × 10 <sup>5</sup>

Table VIII B: 85/85 Test results, V<sub>CC</sub> = 0V.

**Note:** In both 85/85 tests, each pin was alternately biased to + 5V and 0V to provide an electrical potential between adjacent metal lines.

Lot #	48 Hrs.		144 Hrs.		240 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	40	0	40	0	40	$9.6 \times 10^3$
2	0	34	0	33	0	33	$7.9 \times 10^3$
3	0	20	0	20	0	17	$4.4 \times 10^3$
<b>Totals</b>	0	94	0	93	0	90	$2.2 \times 10^4$

Table IX: Autoclave test results.

## Prediction Of Failure Rates

Accelerated testing allows one to identify possible design and process flaws. It also makes it possible to predict failure rates under normal operating conditions. All failure mechanisms are accelerated to some degree by voltage or temperature or both. The degree to which any given failure mode is accelerated is known as the activation energy. Knowledge of a failure mode's activation energy allows one to predict the rate at which that failure mode will occur under normal operating conditions. If the activation energy is not known it can be determined experimentally.<sup>4</sup> Four typical failure mechanisms of the technology employed by Xicor and their corresponding activation energies are:

Oxide breakdown	0.3eV
Leaky oxides	0.6eV
Ionic contamination	1.0eV

Table X presents the predicted failure rates for these activation energies. The results are based on the test data presented in Tables I and IV.

The failure rates predicted are for both plastic and cerdip devices. Such a prediction is valid because all the failure modes found or expected are common to both plastic and cerdip devices. The predicted failure rate is depicted as the "60% upper confidence level" failure rate per 1000 device hours. This means that there is a 60% probability the actual failure rate will be below the rate computed. Sometimes predictions are expressed in FIT units. To convert from the given values to FIT, multiply by 10,000.

A more representative value for the failure rate can be given by the "best estimate". This value gives the most likely failure rate based on the given data. Table XI presents the best estimate values.

Activation Energy	Number of Failures	Equivalent Hours at 70°C	60% UCL Failure Rate Per 1000 Hrs. at 70°C	Equivalent Hours at 55°C	60% UCL Failure Rate Per 1000 Hrs. at 55°C
0.3eV	3	$1.3 \times 10^7$	0.0310	$2.1 \times 10^7$	0.0200
0.6eV	2	$4.0 \times 10^8$	0.0008	$1.0 \times 10^9$	0.0003
1.0eV	3	$6.3 \times 10^8$	0.0007	$2.8 \times 10^9$	0.0002
<b>Totals</b>	8		0.0325		0.0205

Table X: 60% UCL failure rate predictions.

Activation Energy	Number of Failures	Equivalent Hours at 70°C	Best Estimate Failure Rate Per 1000 Hrs. at 70°C	Equivalent Hours at 55°C	Best Estimate Failure Rate Per 1000 Hrs. at 55°C
0.3eV	3	$1.3 \times 10^7$	0.0280	$2.1 \times 10^7$	0.0170
0.6eV	2	$4.0 \times 10^8$	0.0007	$1.0 \times 10^9$	0.0003
1.0eV	3	$6.3 \times 10^8$	0.0006	$2.8 \times 10^9$	0.0001
<b>Totals</b>	<b>8</b>		<b>0.0293</b>		<b>0.0174</b>

Table XI: Best estimate failure rate predictions.

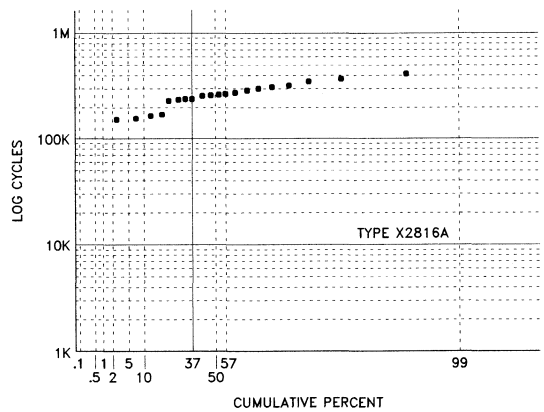
Based on these values it can be seen that the expected failure rate for the X2816A and X2804A is 0.0293% per 1000 hours at 70°C (293 FIT) and 0.0174% per 1000 hours at 55°C (174 FIT).

## Endurance

Xicor uses two tests to evaluate the endurance of its E<sup>2</sup>PROMs. One test utilizes special test modes to enable all bits in a unit to be changed simultaneously. This test is used to measure the ultimate endurance of a sample of units. For reasons discussed in RR-510, this test tends to give a somewhat pessimistic estimate of trapping limited endurance and a slightly optimistic estimate of oxide breakdown limited endurance. Figure 5 shows the endurance distribution from a twenty piece sample from a lot of X2816A showing the intrinsic endurance. In order to monitor the oxide defects, which appear as infant mortality endurance failures, Xicor conducts a test in which the memory is written sequentially 10,000 times on byte-by-byte basis. Two failures were observed on a sample of 300 units from several diffusion lots in this test. As is shown in RR-510, these failures are expected to contribute approximately 10 FIT to the failure rate in typical applications.

## SUMMARY

The technology used in producing the X2816A and X2804A are reviewed. The reasons for expecting excellent data retention are presented. A comprehensive set of data covering a variety of stresses are presented. Finally, failure rate predictions are provided.



0077-9  
Figure 5: An extreme value distribution of endurance monitor on units cycled in mass mode.

## REFERENCES

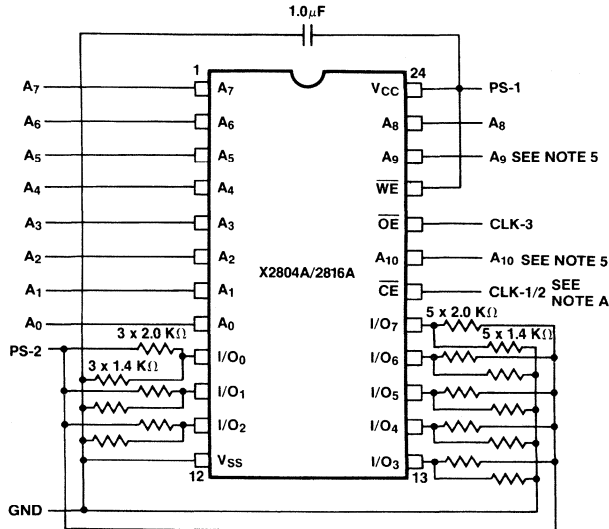
1. R.K. Ellis, *IEEE Electron Device Letters* 13 (1982): pp. 330-333.
2. R.K. Ellis, H.A.R. Wegener and J. Caywood, *International Electron Devices Meeting Technical Digest* (1982): pp. 749-752.
3. J. Caywood and Reliability Engineering Staff, *NOVRAM Reliability Report*, Xicor publication RR-502A (1985).
4. D.S. Peck and O.D. Trap, *Accelerated Testing Handbook*, Technical Associates Publication.

This report is based on data collected through January, 1986.

# APPENDIX A

Product	Package Type					
	Plastic		Cerdip		LCC	
	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$
X2804A	50.0	81.0	20.5	36.0	—	—
X2816A	45.0	72.5	18.0	32.0	5.5	53.5

Thermal Resistance Table:  $\theta_{JC}$  and  $\theta_{JA}$  expressed in °C per watt.



0077-7

## Note A:

CLK-1: Rows 1, 3, 5 . . . (odd rows— $\overline{CE}_A$ )  
 CLK-2: Rows 2, 4, 6 . . . (even rows— $\overline{CE}_B$ )  
 Such that: CLK-2 =  $\overline{CLK-1}$

**Note B:** (1)  $\overline{WE}$  must always be hardwired to VCC (Pin 24) at device as shown.

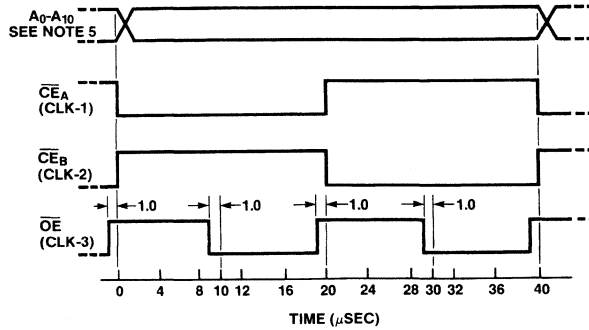
(2) All resistors:  
 1% metal film  
 1/4 W

(3) I/O pull-up: 2.0 K $\Omega$   
 I/O pull-down: 1.4 K $\Omega$

(4) Socket-to-socket isolation as shown.

(5) Pin 19 (A<sub>10</sub>) and Pin 22 (A<sub>9</sub>) are no connects (NC) for the X2804A.

X2804A/2816A (DIP) Burn-in circuit.

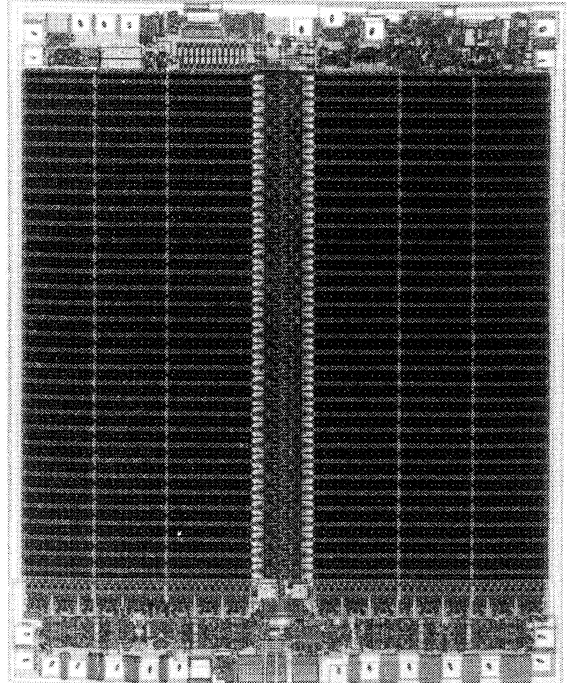


0077-8

- Notes:** (1)  $A_0-A_{10}$ : binary sequencing address cycle: 40  $\mu$ s.  
 (2)  $\overline{WE}$  disabled (tied to  $V_{CC}$  at device).  
 (3)  $V_{IN}$  Low: 0.4V  $V_{IN}$  High: 5.0V  
 (4)  $V_{CC}$ : 5.50V  
 (5) X2804A:  $A_0-A_8$   
 X2816A:  $A_0-A_{10}$

*X2804A/2816A (DIP) Burn-in timing diagram.*





0078-1

# **BYTE-WIDE NOVRAM\* (X2001/X2004) RELIABILITY REPORT**

**By Atam Kablanian**

**8**

\*NOVRAM is Xicor's nonvolatile static RAM device.

# INTRODUCTION

This is a summary of RR-506, the report of reliability studies conducted by Xicor to fully qualify the X2001/X2004 family of byte-wide NOVRAMs. This family is comprised of the X2001 configured 128 x 8 and the X2004 configured 512 x 8. Although the data were collected using the X2004, the entire family shares common circuitry throughout and they are all manufactured employing the same process criteria.

Figure 1 provides pinouts for the two parts; Figure 2 shows the functional block diagram for the X2004; Figures 3 and 4 illustrate the physical location of the various address bits. The thermal resistance table, burn-in circuit and a timing diagram are included in Appendix A for your reference.

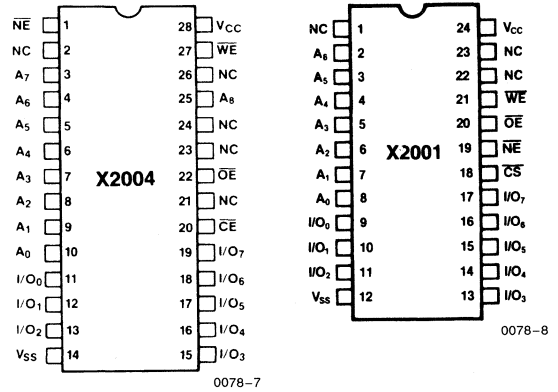


Figure 1: X2004 and X2001 pin configurations.

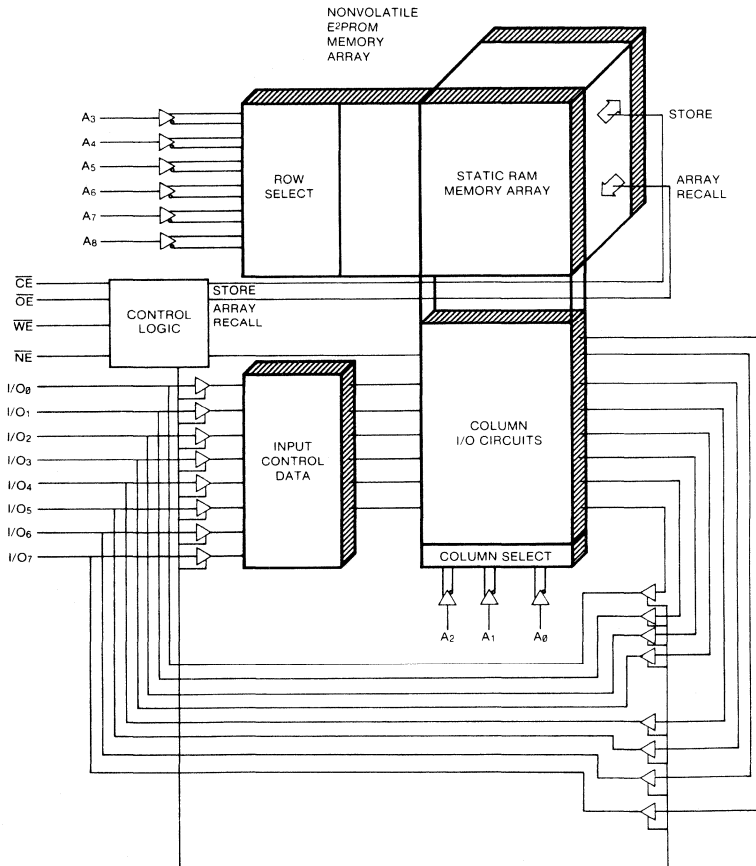
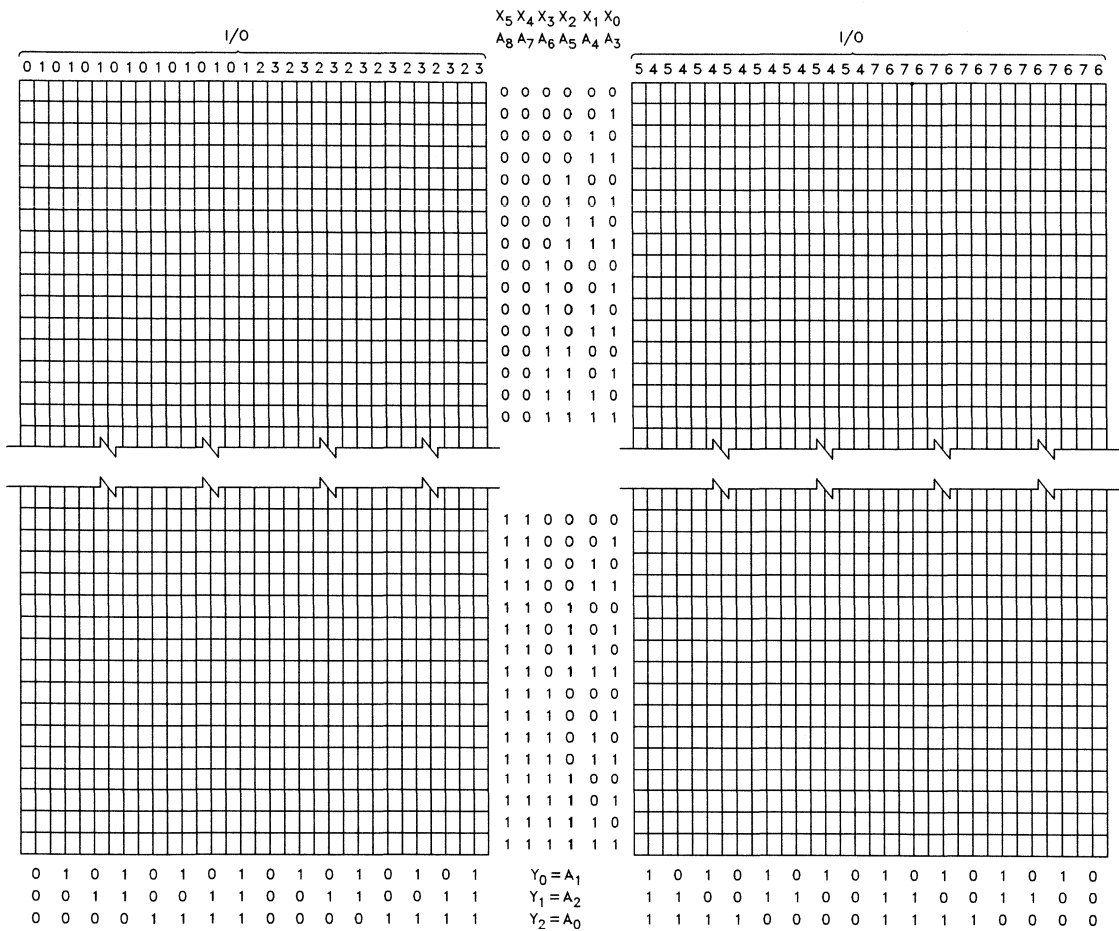


Figure 2: X2004 functional block diagram.



Each square equals one bit.

Figure 3: X2004 physical bit map.

0078-5





The E<sup>2</sup>PROM portion of the memory cell employs a triple polysilicon N-channel process, see Figure 6. Data is stored as the presence or absence of charge on the second level polysilicon which in turn acts as the gate for the readout transistors. This second level polysilicon is surrounded by ~ 800Å of SiO<sub>2</sub>, electrically isolating it from the other layers, allowing storage of charge on the second level polysilicon until a large energy input from an outside source is received. In the E<sup>2</sup>PROM cell charge is transferred onto or off of this storage gate in a controlled manner by means of a quantum mechanical phenomenon, called Fowler-Nordheim tunneling.<sup>1</sup>

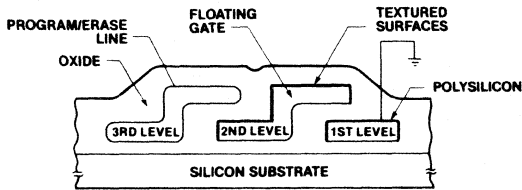


Figure 6: E<sup>2</sup>PROM cell structure.

0078-3

This charge transfer occurs only during store operations. There are two types of storage mechanisms that occur during the store operation, however each bit will only experience one. Should the state of the floating gate need to be changed, it will either be programmed (charged) or erased (discharged). There is a third possibility; in order to extend the endurance of the E<sup>2</sup>PROM cell no charge transfer will occur if the state of the RAM cell and E<sup>2</sup>PROM are already the same.

## Nonvolatile Memory Reliability Concerns

E<sup>2</sup>PROMs are unique semiconductors when examined from a reliability viewpoint. Most LSI semiconductor devices such as microprocessors are evaluated solely for semiconductor type reliability; generic nonvolatile memories such as EPROMs or ROMs are evaluated for semiconductor reliability and data retention; but E<sup>2</sup>PROMs must be evaluated for semiconductor reliability, data retention and endurance.

- Data retention refers to the capability of a nonvolatile memory to retain valid data under worst case conditions.

- Semiconductor reliability pertains to several failure modes common to all semiconductors such as oxide rupture and microcracks. These are generally process related failure mechanisms.
- Endurance is the ability of a nonvolatile memory device to sustain repeated data changes.

Semiconductor failures and endurance failures can be further categorized as infant mortality failures, early life failures, random failures and end of life or wearout failures. These failures would fit the classic bathtub curve illustrated in Figure 7. Xicor production test flows are designed to eliminate infant mortality failures and reduce the incidence of early life failures. All devices employed in the reliability study were selected from units that had completed the standard test flow in order to indicate failure rates that might be experienced after shipment to customers.

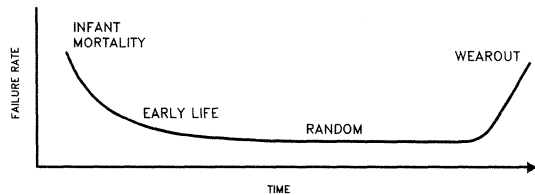


Figure 7: Illustration of bathtub curve of failure rates.

0078-4

## Retention

This test is sometimes referred to as storage bake, but Xicor prefers the term “data retention bake” because this better describes the principal function it serves in the case of electrically programmable nonvolatile memories.

In this test an erase pattern, or a charge that is the opposite of the state that would be read when the gate is at equilibrium, is stored on the floating gate of the E<sup>2</sup>PROM cells. The devices are then baked at 250°C with no bias applied. At intervals the memory is removed from the bake and the nonvolatile data is recalled and verified. The data is **not** restored to the E<sup>2</sup> array after the readouts in order to ascertain the worst case retention capability.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	24	0	24	0	24	0	24	0	24	0	24	48000
2	0	30	0	30	0	30	0	30	0	30	0	30	60000
3	0	50	0	50	0	50	0	50	0	50	0	50	100000
4	0	50	0	50	0	50	0	50	0	50	0	50	100000
5	0	50	0	50	0	50	0	50	0	50	0	50	100000
<b>Totals</b>	0	204	0	204	0	204	0	204	0	204	0	204	408000

Table I: 250°C Data retention bake test results.

Xicor has experimentally determined the activation energy ( $E_a$ ) for the data loss mechanism of the E<sup>2</sup> cell to be 1.7 eV. The mean time for data loss for this mechanism, which we believe to be the fundamental data loss mechanism of this technology, is 3 million years at 125°C. Table I illustrates the results of the data retention tests performed on the X2004.

## Semiconductor Reliability

Table II is a compilation of MOS failure mechanisms and the normal test method used to accelerate failures caused by that mechanism. The acceleration of failures is required in order to collect statistically useful data in the most expeditious manner.

## High Temperature Lifetest

This test employs elevated temperatures to accelerate all failure types related to infant mortality and random failures. This data is gathered at 125°C ambient temperature. The E<sup>2</sup> array is erased and the static RAM array is constantly being written with FF(H) then read and then rewritten with 00(H) and read again. Full AC and DC testing is done at 48, 168, 500, 1000, 1500 and 2000 hours to insure device functionality. After each of the first five tests the E<sup>2</sup> array is once again erased and the devices continue the lifetest. The results of the tests are shown in Table III.

## High Temperature Reverse Bias

This test is performed at 150°C, with the GND pin tied to 0V and all other pins tied to V<sub>CC</sub>. Two separate tests were performed; the first was with V<sub>CC</sub> at

5.5V and the second with V<sub>CC</sub> at 7.5V. This test is performed to expose failures which might occur as result of drift of mobile ionic contamination or latent defects in the gate oxides. The results of the tests are shown in Tables IV and V.

Failure Mechanism	Type	Activation Energy	Detection Method
Ionic Contamination	Infant/Random/Wearout	1.0eV	High Temp. Bias
Surface Charge	Wearout	0.5–1.0eV	High Temp. Bias
Polarization	Wearout	1.0eV	High Temp. Bias
Electromigration	Wearout	0.55eV	High Temp. Operating Life
Microcracks	Random	—	Temperature Cycling
Contact Electromigration	Wearout	0.9eV	High Temp. Bias/High Temp. Operating Life
Oxide Rupture	Infant/Random	0.3eV	High Temp. Operating Life
Silicon Defects	Infant/Random	0.3eV	High Temp. Bias
Oxide Defect Leakage	Infant/Random	0.6eV	High Temp. Operating Life
Electron Trapping in Oxide	Wearout	0.06eV	Low Temp. High Voltage Operating Life

Table II: MOS failure mechanisms and test acceleration test method.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1	1[a]	131	0	130	0	81	0	81	0	81	0	81	170280
2	0	187	0	187	0	112	0	112	0	112	0	112	236600
3	0	206	0	206	0	101	0	101	0	100	0	100	218640
4	0	105	0	105	0	0	0	0	0	0	0	0	17640
5	0	189	0	189	1[b]	84	0	82	0	82	0	82	182640
6	0	229	0	229	0	54	0	54	0	52	0	52	135400
7	0	229	0	229	0	55	0	55	0	55	0	55	139232
8	0	238	0	238	1[c]	63	0	62	0	62	0	62	153900
<b>Totals</b>	<b>1</b>	<b>1514</b>	<b>0</b>	<b>1513</b>	<b>2</b>	<b>550</b>	<b>0</b>	<b>547</b>	<b>0</b>	<b>544</b>	<b>0</b>	<b>544</b>	<b>1254332</b>

[a] 1 unit—single bit oxide breakdown,  $E_a = 0.3\text{eV}$

[b] 1 unit—single bit oxide breakdown,  $E_a = 0.3\text{eV}$

[c] 1 unit—ionic contamination,  $E_a = 1.0\text{eV}$

Table III: High temperature dynamic lifetest results.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1	0	25	0	25	0	25	0	25					25000
2	0	15	0	15	0	15	0	15					15000
3	0	15	0	15	0	15	0	15					15000
4	0	15	0	15	0	15	0	15					15000
5	0	15	0	15	0	15	0	15					15000
6	0	25	0	25	0	25	0	25	0	24	0	24	49000
7	0	25	0	25	0	25	0	25	0	24	0	24	49000
8	0	25	0	25	0	25	0	25	0	25	0	25	50000
<b>Totals</b>	<b>0</b>	<b>160</b>	<b>0</b>	<b>160</b>	<b>0</b>	<b>160</b>	<b>0</b>	<b>160</b>	<b>0</b>	<b>73</b>	<b>0</b>	<b>73</b>	<b>233000</b>

Table IV: High temperature reverse bias lifetest results at 5.5V.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
3	0	15	0	15	0	15	0	15	15000
4	0	15	0	15	0	15	0	15	15000
5	0	15	0	15	0	15	0	15	15000
<b>Totals</b>	<b>0</b>	<b>45</b>	<b>0</b>	<b>45</b>	<b>0</b>	<b>45</b>	<b>0</b>	<b>45</b>	<b>45000</b>

Table V: High temperature reverse bias lifetest results at 7.5V.



# Failure Rate Calculation and Reliability Prediction

High temperature lifetest and high temperature reverse bias data are used to calculate the failure rate. If we ignore the infant mortality failures (failures before 48 hours burn-in), we can then calculate the failure rate for the useful life of the device as follows:

$$\text{Failure Rate } (T_s) = \frac{\text{number of failures}}{\text{Device Hours } (T_s)}$$

$T_s = \text{stress temperature}$

The above equation will be useful only to calculate the failure rate at the stress temperature under which the tests were performed. In most cases the actual operating temperature of the device will be much lower; therefore, the equation needs to be modified to reflect the failure rate at the operating temperature. The failure rate for a given activation energy is calculated as follows:

$$\text{Failure Rate } (T_d)_i = \frac{N_i}{\text{DH}(T_s) \times \text{TAF}(T_s, T_d)_i \times \text{VAF}(V_s, V_d)_i}$$

Where:

Failure Rate  $(T_d) = \frac{\text{Failure rate at temperature } T_d}{\text{DH}(T_s)}$

$\text{DH}(T_s) = \text{Device hours at stress temperature}$

$\text{TAF}(T_s, T_d) = \text{Temperature acceleration factor from } T_s \rightarrow T_d$

$i = \text{A given activation energy}$

$N_i = \text{Number of failures for activation energy } i$

$T_s = \text{Stress temperature}$

$T_d = \text{Desired temperature}$

$\text{VAF}(V_s, V_d) = \text{Voltage acceleration factor from } V_s \rightarrow V_d$

$V_s = \text{Stress Voltage}$

$V_d = \text{Desired Voltage (5.5V)}$

The voltage acceleration factor is 1 for all failure mechanisms except TDDB (time dependent dielectric breakdown where  $E_a = 0.3\text{eV}$ ). This can be calculated using Crook's equation:<sup>2</sup>

$$\text{VAF}(V_s, V_d) = \exp [(E_s - E_d)/E_{ef}]$$

Where:

$E_s = \text{Field (stress)} = V_s/T_{ox}$

$E_d = \text{Field (desired)} = V_d/T_{ox}$

$E_{ef} = \text{Field constant} = 0.062 \text{ Mv/cm}$

$T_{ox} = \text{Oxide thickness}$

The temperature acceleration factor for a given activation energy can be calculated using the Arrhenius equation:

$$\text{TAF}(T_s, T_d) = \exp[(E_a/K) (1/T_s - 1/T_d)]$$

Where:

$E_a = \text{Activation energy (eV)}$

$K = \text{Boltzmann's constant}$   
( $8.63 \times 10^{-5} \text{ eV/}^\circ\text{K}$ )

$T_s = \text{Stress temperature (junction) in } ^\circ\text{K}$

$T_d = \text{Desired temperature (junction) in } ^\circ\text{K}$

The above equation is valid for only one activation energy. To predict the total failure rate for the device at the desired temperature the calculated failure rates for each activation energy must be summed.

Total Failure Rate  $(T_d) =$

$$\sum_i \frac{N_i}{\text{DH}(T_s) \times \text{TAF}(T_s, T_d)_i \times \text{VAF}(V_s, V_d)_i}$$

Using the above equation we calculated the failure rate based on the experimental results. Those calculations are summarized in Table VI. We have also included in that table a 60% upper confidence level (UCL) calculation. This indicates that with a 60% confidence the actual failure rate will be below that calculated. The equation below is used to determine the 60% UCL.

Total Failure Rate  $(T_d) =$

$$\sum_i \frac{X^2(1 - CL)(2N + 2)}{2 \times \text{DH}(T_s) \times \text{TAF}(T_s, T_d)_i \times \text{VAF}(V_s, V_d)_i}$$

Where:

$X = \text{the chi square function}$

$CL = \text{the confidence limit (60\%)}$

$2N + 2 = \text{the degrees of freedom}$



Ae in eV	Total Device Hours		# of Fails	Equivalent Device Hours		Calculated Failure Rate FIT		60% UCL Failure Rate FIT	
	@ 125°C	@ 150°C		@ 55°C	@ 70°C	@ 55°C	@ 70°C	@ 55°C	@ 70°C
0.3	$1.18 \times 10^6$	$2.78 \times 10^5$	1	$2.91 \times 10^7$	$1.97 \times 10^7$	35	51	70	105
0.6	$1.18 \times 10^6$	$2.78 \times 10^5$	0	$4.65 \times 10^7$	$2.15 \times 10^7$	0	0	20	43
1.0	$1.18 \times 10^6$	$2.78 \times 10^5$	1	$5.38 \times 10^8$	$1.34 \times 10^8$	2	7	4	14
<b>Totals</b>			2			37	58	94	162

Note: FIT  $\times$  0.0001 = failure rate per thousand hours.

Table VI: Summary of semiconductor failure rate calculations.

In calculating the data presented in Table VI we used the actual junction temperature and not ambient temperature. We also made the conservative assumption of including the oxide leakage ( $E_a = 0.6\text{eV}$ ) failure rate. This failure mechanism should be included whether it was observed or not, since it is always anticipated in the E<sup>2</sup>PROM technology. Had we only considered the observed failures as many vendors do, the 60% UCL failure rate at 70°C and 55°C would have been 119 and 74 FIT respectively versus the more conservative calculation of 162 and 94 FIT.

The results in Table VI are long term failure rates and were determined by excluding data for the first 48 hours of the dynamic lifetest. Infant mortality can be calculated from the data contained in Table III. There was one failure out of 1514 units tested; yielding a single point estimate of 660 ppm.

Infant mortality rates and long term failure rates indicate Xicor's byte-wide NOVRAMs have attained failure rates comparable if not better than those reported by major semiconductor suppliers of standard volatile memory products.<sup>5,6,7</sup>

## Endurance

A key factor in memory system reliability is the ability of the device to sustain repeated data changes. In the static RAM portion of the NOVRAM there are only semiconductor related reliability factors. However, the E<sup>2</sup> array is subject to limitations on the number of data changes a cell may undergo, its limit of endurance. Xicor defines the endurance limit

of a memory is reached when the first single bit failure occurs. This limit of endurance is expressed in number of data changes the entire array can sustain before a single bit fails to change.

The endurance test employed is to alternately store all ones then all zeroes in the array. The array is verified after each data change. Upon detection of the first single bit failure the number of cycles that device endured is recorded.

Figure 8 contains the data for a typical endurance monitor lot of X2004. These data are displayed on an extreme value distribution plot. For more information on endurance, see Xicor RR-504 and RR-510.

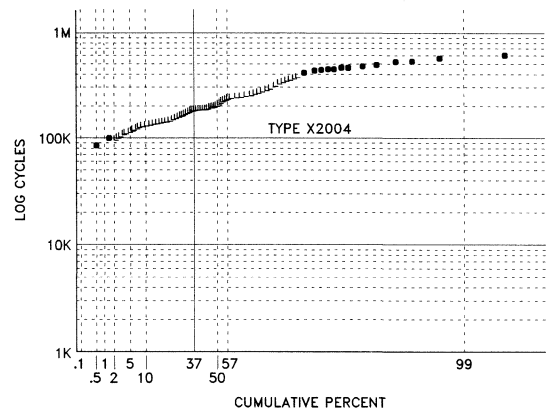


Figure 8: Extreme value distribution plot for X2004.

0078-12

## Low Temperature Dynamic Lifetest

In addition to the preceding tests pertaining to standard failures related to nonvolatile memories Xicor undertook a test to determine if hot electron trapping was of concern for this device family. The low temperature dynamic lifetest is functionally identical to the high temperature dynamic lifetest but with the ambient temperature at  $-40^{\circ}\text{C}$ . This test is intended to detect hot electron trapping in the gate oxide. As can be seen by the test results in Table VII, there was no indication of hot electron trapping in these devices.

## Environmental Testing

This group of tests is performed on plastic packages to insure that excessive humidity and ambient vapors will not cause failures and to insure temperature cycling will have no adverse effects on the materials used.

The three major failure modes for plastic packaged devices under moisture test are:

- Mobile Ions—Ions on the passivation glass are made more mobile by humidity. If enough charge transfer occurs, a device parameter could be altered or a parasitic transistor could be introduced, degrading device performance.
- Chemical Corrosion—Phosphorous is commonly used in small quantities in passivation and under metalization layers. Sufficient phosphorous, when combined with water molecules, produces phosphoric acid which may etch away aluminum lines.
- Electrolytic Corrosion—When a voltage potential exists between two adjacent metal lines under enhanced surface conditions, presence of moisture, and electrolytic corrosion process may be triggered. This condition could result in an open metal line.

Autoclave and  $85^{\circ}\text{C}/85\%$  relative humidity tests are conducted to test for these failure modes.

## Autoclave

Autoclave or pressure pot testing subjects a device to a 2 atmosphere steam environment. This test will accelerate mobile ionic drift, chemical corrosion and to some extent electrolytic corrosion. The test results are summarized in Table VIII.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
2	0	30	0	30	0	30	0	30	0	30	0	30	60000
3	0	25	0	25	0	25	0	25	0	25	0	25	50000
4	0	25	0	25	0	25	0	25	0	25	0	25	50000
5	0	25	0	25	0	25	0	25	0	25	0	25	50000
<b>Totals</b>	0	105	0	105	0	105	0	105	0	105	0	105	210000

Table VII: Low temperature dynamic lifetest results.

Lot #	48 Hrs.		144 Hrs.		240 Hrs.		336 Hrs.		432 Hrs.		528 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
6	0	48	0	48	0	48	0	48	0	48	0	48	25344
7	0	49	0	49	0	49	0	49	0	49	0	49	25872
8	0	50	0	50	0	50	2[a]	50	0	48	0	48	26016
<b>Totals</b>	0	147	0	147	0	147	2	147	0	145	0	145	77232

[a] 2 units—open pins, chemical corrosion

Table VIII: Autoclave test results.

## 85°C and 85% Relative Humidity

85/85 testing is performed to determine life expectancy of devices in high temperature and high humidity environments. This test will accelerate the three environmental failure modes. It is an especially good test for detecting electrolytic corrosion.

85/85 tests can be performed in two ways. The first is by supplying voltage to  $V_{CC}$  with all other pins alternately biased at 0V and +5V. In this method, heat generated by power dissipation can reduce the relative humidity on the die surface to as low as 45%. The second method is to test the device with  $V_{CC}$  at 0V and all other pins alternately biased at 0V and +5V. This provides a potential between metal lines and insures maximum humidity at the die surface. The second method is more stringent and is the method used to test the X2004. The results of the test are listed in Table IX.

Lot #	168 Hrs.		500 Hrs.		1000 Hrs.	
	# Fail	# In	# Fail	# In	# Fail	# In
6	0	50	0	50	0	50
7	0	50	0	50	0	50
8	0	50	0	50	0	50
<b>Totals</b>	0	150	0	150	0	150

Table IX: 85°C/85% Test results.

## Temperature Cycling

This test subjects the devices to temperature extremes of  $-65^{\circ}\text{C}$  to  $+165^{\circ}\text{C}$ . This test is performed to stress the package to detect poor bond wire attachment and to determine if there is a potential problem due to thermal mismatch between the die and the package material that could cause device failures. The results of this test are tabulated in Table X.

Lot #	168 Cycles		500 Cycles		1000 Cycles	
	# Fail	# In	# Fail	# In	# Fail	# In
6	0	50	0	50	0	50
7	0	50	0	50	0	50
8	0	50	0	50	0	50
<b>Totals</b>	0	150	0	150	0	150

Table X: Temperature cycling test results.

## SUMMARY

The data presented show that data retention is excellent. There were no observed retention failures. The X2004 family exhibits semiconductor related failure rates comparable if not better than those reported by other semiconductor manufacturers. The typical minimum endurance limit of the X2004 is an order of magnitude higher than 10,000 cycles. The plastic packaging employed shows excellent results.

## REFERENCES

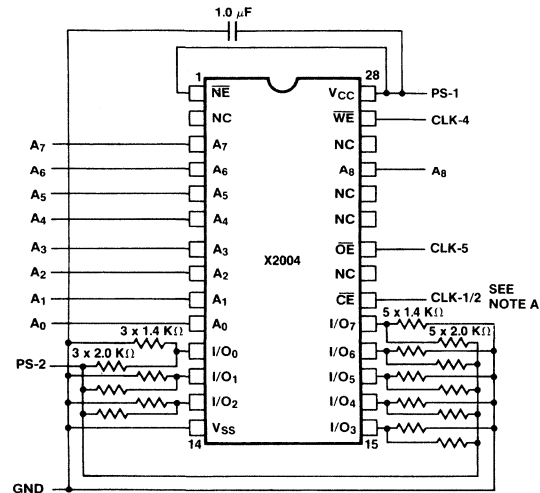
1. R.H. Fowler and L. Nordheim, Proceedings of the Royal Society of London, A119, (1928); pp. 173-181.
2. Dwight L. Crook, 17th Annual Reliability Symposium, (1979); 1-7.
3. H.A.R. Wegener, *Endurance of Xicor E2PROMs and NOV RAMs*, (Xicor, 1984).
4. Bruce Euzent, *2115/2125 N-Channel Silicon Gate MOS 1K Static RAMs*, (1976) Intel Reliability Report RR-14.
5. Chieh Lin Ping, *Reliability of N-Channel Metal Gate MOS/LSI Microcircuits*, (1982), National Semiconductor.
6. Bruce Euzent and Stuart Rosenberg, *HMOS Reliability*, (1978), Intel Reliability Report RR-18.

This report is based on data collected through December, 1985.

# APPENDIX A

Product	Package Type					
	Plastic		Cerdip		LCC	
	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$
X2001	42.7	77	19.5	34.5	—	—
X2004	39.5	64.3	16.5	33.5	5.0	46.5

Thermal Resistance Table:  $\theta_{JC}$  and  $\theta_{JA}$  expressed in °C per watt.



0078-10

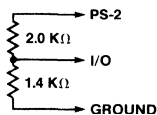
**Note A:**

CLK-1: Rows 1, 3, 5, ... (odd rows =  $\overline{CE-A}$ )  
 CLK-2: Rows 2, 4, 6, ... (even rows =  $\overline{CE-B}$ )  
 CLK-2 =  $\overline{CLK-1}$

**Note B:** (1) NE (Pin 1) must be hardwired to VCC (Pin 28) at device as shown.

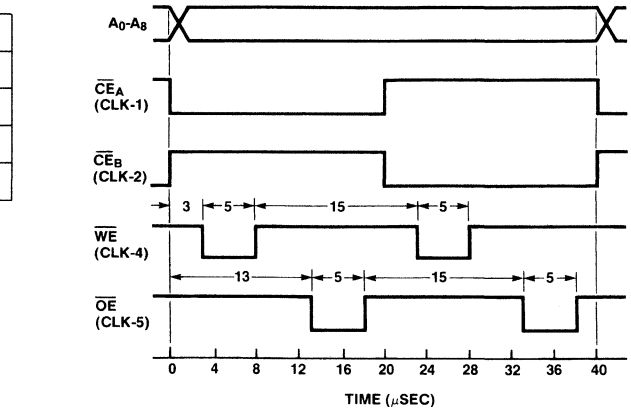
(2) All resistors:  
 1% metal film  
 1/4 W

(3) All I/O's:



(4) Socket-to-socket isolation as shown.

X2004 (DIP) Burn-in circuit.



0078-11

**Notes:** (1) A<sub>0</sub>-A<sub>8</sub>: binary sequencing cycle period: 40 µs.

(2) NE disabled (tied to V<sub>CC</sub> at device).

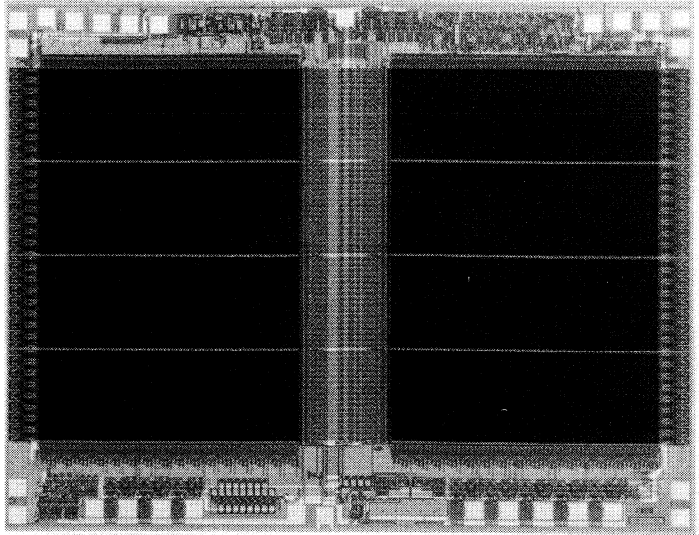
(3) Low state: 0.4V max.

High state: 5.0V typ.

V<sub>CC</sub>: 5.50V

X2004 (DIP) Burn-in timing diagram.

0078-13



0079-1

# **X2864A RELIABILITY REPORT**

**By Troy Kaysser  
and Lori J. Purvis**

# INTRODUCTION

The X2864A is a 64K bit electrically erasable programmable read only memory, E<sup>2</sup>PROM, organized 8K x 8. This memory operates on a single 5V power supply for all operations. Figure 1 provides the 64K pin configuration; Figure 2 shows the functional block diagram; Figure 3 illustrates the physical location of the various address bits. The thermal resistance table, burn-in circuit and a timing diagram are include in Appendix A for your reference.

The X2864A is manufactured using Xicor's rugged, textured poly technology. Xicor has shipped more than 20 million memories manufactured with this technology. Because the X2864A is a mature part which has been in volume production for some time, this report contains data from the production reliability monitor as well as reliability qualification data.

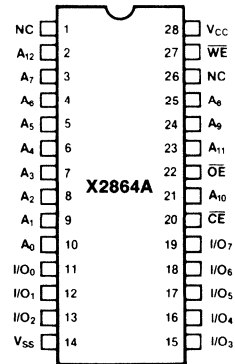


Figure 1: X2864A Pin configuration.

0079-9

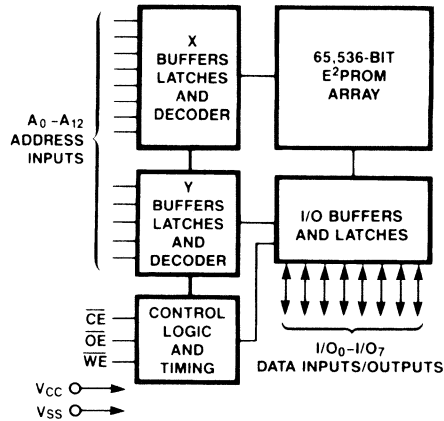
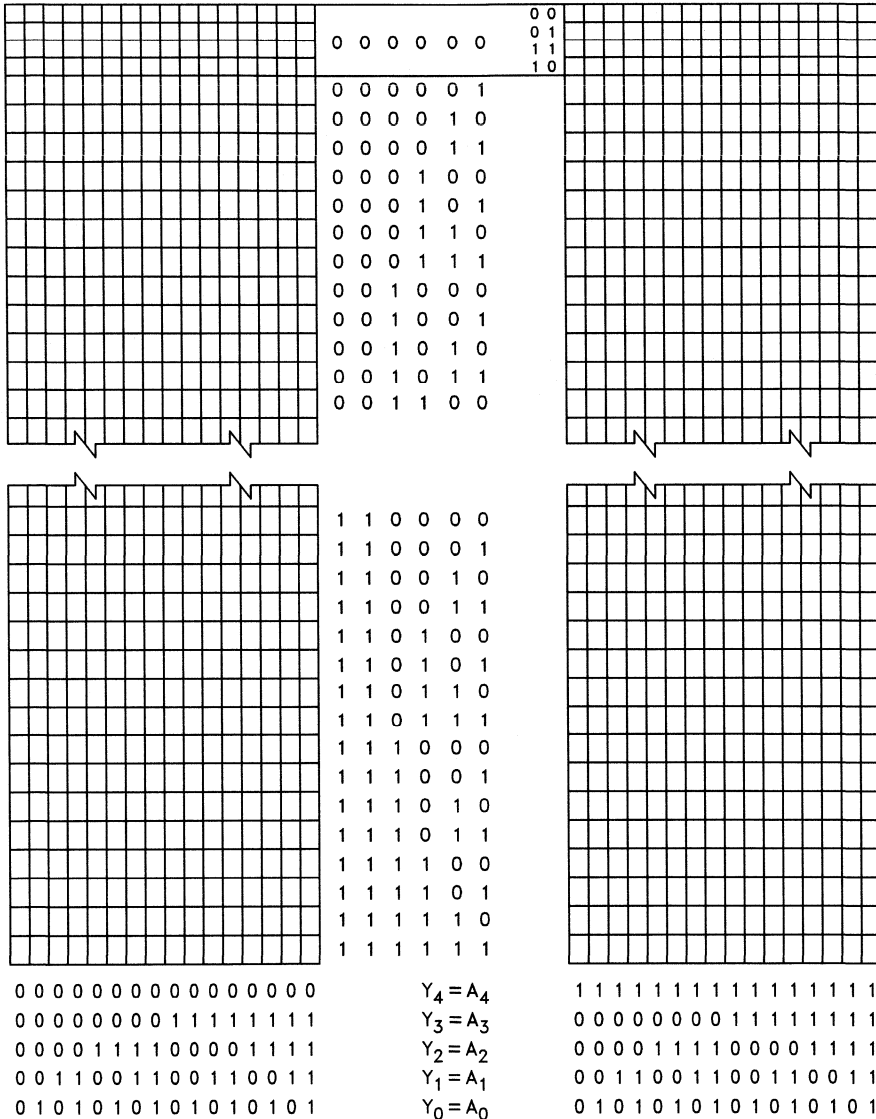


Figure 2: X2864A Functional block diagram.

0079-10

X<sub>7</sub> X<sub>6</sub> X<sub>5</sub> X<sub>4</sub> X<sub>3</sub> X<sub>2</sub> X<sub>1</sub> X<sub>0</sub>  
A<sub>12</sub> A<sub>11</sub> A<sub>10</sub> A<sub>9</sub> A<sub>8</sub> A<sub>5</sub> A<sub>6</sub> A<sub>7</sub>



Each square equals one byte.

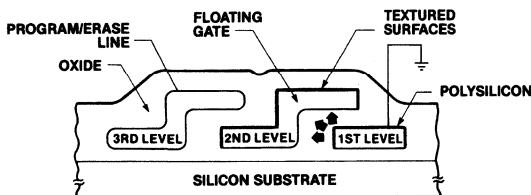
Figure 3: X2864A Physical bit map.

0079-11

In the next section the operation of the textured poly E<sup>2</sup>PROM cell is described. The remainder of the report covers experiments designed to probe the reliability of the part beginning with the two attributes unique to E<sup>2</sup>PROMs: data retention and endurance. The data show that at 55°C retention contributes approximately 1 FIT to the device failure rate while endurance contributes about 10 FIT in a typical application. After the E<sup>2</sup>PROM specific experiments, standard accelerated lifetest and accelerated package tests are reported in order to complete the study on this component. These results are used to predict operating failure rate. The predicted result is 50 FIT at 55°C, 60% UCL.

## TEXTURED POLY E<sup>2</sup>PROM CELL

The cross sectional structure of a textured poly cell is shown in Figure 4. It consists of 3 layers of poly with overlap forming three transistors in series. The floating gate transistor is in the middle formed by poly 2. The floating gate is surrounded by silicon dioxide for high retention. Programming is achieved by electrons tunneling from poly 1 to poly 2 and erase is achieved by electrons tunneling from poly 2 to poly 3.



0079-2

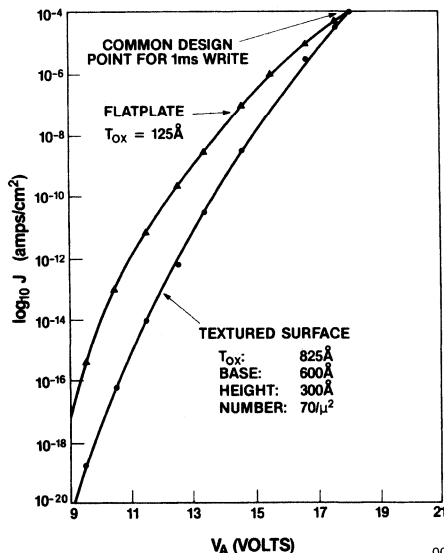
Figure 4: Cross sectional structure of a textured poly memory cell.

In reading the datum stored in the cell the poly 3 select transistor is enabled. The current flow through the cell is determined by the charge state of the poly 2 floating gate. If it is charged positively when the bit is selected, current flows through the cell which is sensed as a "1". If it is charged negatively, a "0" results. During writing the poly 3 is set to a high voltage (> 20V). The poly 2 floating gate is capacitatively steered either high or low. If the floating gate is steered low, the large voltage drop occurs between poly 2 and poly 3 causing electrons to tunnel off the floating gate, leaving it in a positively charged erase state. If the floating gate is

steered high, the large voltage drop occurs between poly 1 and poly 2 causing electrons to tunnel from poly 1 onto the floating gate charging it negative.

## DATA RETENTION

Textured poly tunneling structures have a significant advantage in data retention in comparison with those employing flat surfaces and thin oxides. One basis for this advantage is illustrated in Figure 5, in which the current-voltage (J-V) characteristics of a tunneling device which employs a thin oxide between planar surfaces and, a tunneling device which employs a thick oxide between textured silicon surfaces, are compared. For this comparison we match the currents in the high current region since most memories are designed to program in about the same time period (~ 10 ms). As can be seen, the same current can be obtained from a smooth surface with 125Å thick tunnel oxide or from a textured surface with an 825Å thick tunnel oxide. Note however, that at lower values of applied voltage typical of read and storage conditions, the current emitted from a textured surface is approximately four orders of magnitude lower than that from a smooth surface.



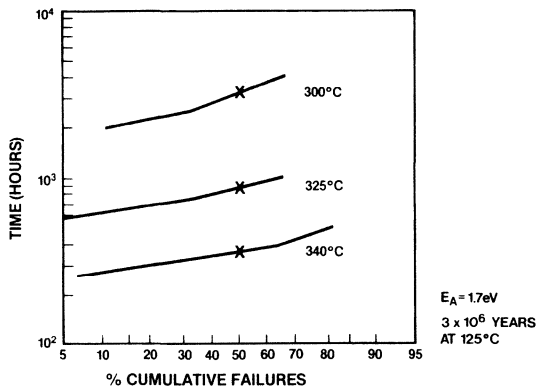
0079-3

Figure 5: Comparison of calculated tunneling J-V curves for emission from a planar and a textured structure. The devices were designed to have the same emission in the high current regime where programming takes place.



These differences may become even more significant as devices are scaled. It is clear that, in order to scale the memory properly, lower programming voltages are needed so that the isolation widths and device channel lengths can be reduced both in the memory array and in the peripheral circuitry. However, for a typical part which stores data in 3 ms and must retain it for 10 years, the tunneling current under storage and reading conditions must be at least  $10^{11}$  times smaller than under programming conditions because the retention time is  $10^{11}$  times longer than the storage time. Actually, for margin, one would design for a difference in currents of  $10^{13}$  to  $10^{14}$ . For planar surface tunneling structures, this may be a difficult design constraint because the slope of the J-V curve is fixed, which means that the maximum allowed read voltage drops with the programming voltage on a volt-for-volt basis, not proportionately. On the other hand, textured surface tunneling structures, in their current manifestation, have a steeper J-V characteristic than planar ones and the J-V characteristic of a textured structure can be tailored to yield a steeper curve if desired. This means that for a given maximum read voltage, a textured structure requires a lower programming voltage which leads to better scaling.

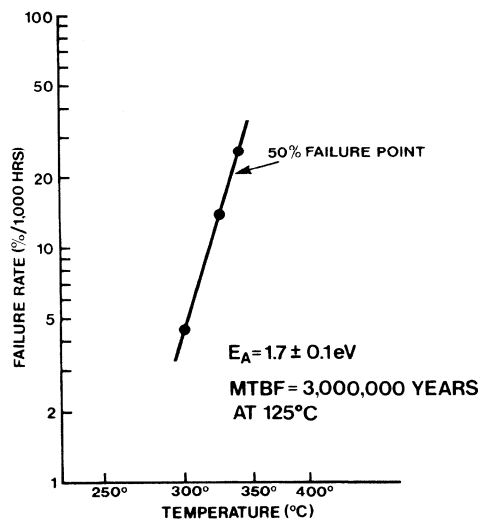
To verify the excellent data retention expected of Xicor memories, a study was carried out to measure data loss as a function of temperature. Figure 6 shows log cumulative data loss vs. log time for 100 samples of X2210's at each of three temperatures. Data loss is defined as occurring when the first bit in the array loses data. As shown in Figure 6, high temperatures were required to obtain appreciable



0079-4  
Figure 6: Log cumulative data loss vs. log time for three storage temperatures on samples of 100 X2210's. Data loss is defined to occur when the first bit in an array loses data.

\*NOVRAM is Xicor's nonvolatile static RAM device.

data loss in experimentally useful times. Note that even at 300°C, 2000 hours ( $\sim 3$  months) are required to see data loss. Figure 7 shows the result of calculating failure rates based on these results and plotting vs. inverse temperature. Since the rates fall on a straight line, we can extract an activation energy and extrapolate to lower temperatures. The result is that the experimental value of the activation energy is 1.7eV and the mean time for data loss for this mechanism (which we believe to be the fundamental loss mechanism of this technology) is 3 million years for retention at 125°C.



0079-5  
Figure 7: Log data loss rate vs. inverse temperature for X2210's.

Although this retention data was based on small NOVRAMs\*, it applies equally to Xicor E<sup>2</sup>PROMs which share common floating gate storage mechanisms and processes with the NOVRAMs. In fact, the real cause for retention failures observed in E<sup>2</sup>PROMs is not the intrinsic mechanism reported above, but single bit data loss arising from the same oxide defects which have been observed in EPROMs and shown to have an activation energy of 0.6eV.<sup>1</sup>

In order to investigate the probability of occurrence of the extrinsic oxide defect data retention failures, a topological checkerboard pattern was written into samples of X2864A devices from a number of lots. These devices were stored at elevated temperatures with periodic readouts to verify to data integrity. The hermetic packaged devices were stored at 250°C while the tests on the plastic encapsulated devices were conducted at 150°C because

**150°C**

Package Type	Lot ID	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.	
PLCC	Q1	0	27	0	27	0	27	0	27	0	27	0	27
	Q2	0	28	0	28	0	28	0	28	0	28	0	28
PDIP	Q1	0	50	0	50	0	50	0	50	0	50	0	50
	Q2	0	50	0	50	0	50	0	50	0	50	0	50
	Q3	0	50	0	50	0	50	0	50	0	50	0	50
<b>Totals</b>		0	205	0	205	0	205	0	205	0	205	0	205

**250°C**

Package Type	Lot ID	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.	
Cerdip	Q1	0	50	0	50	0	50	0	50
	Q2	0	50	0	50	0	50	0	50
	Q3	0	50	0	50	0	50	0	50
	Q4	0	50	0	50	0	50	1 [a]	50
	Q5	0	50	0	50	0	50	0	50
	Monitor	0	350	0	350	0	350	1 [b]	350
<b>Totals</b>		0	600	0	600	0	600	2	600

[a] = Cracked die

[b] = Single bit retention failure: 0.6eV

Table I: Data retention bake.

the plastic epoxy molding compound won't survive 250°C storage. The data from this test are displayed in Table I. The results show very good data integrity. This is in line with a recent report which indicated that E<sup>2</sup>PROMs have a lower incidence of oxide defects than EPROMs.<sup>2</sup> This is probably because the multiple high voltage writes which occur during an E<sup>2</sup>PROM manufacturing flow provide an effective screen for many oxide defects which would otherwise appear as retention failures.

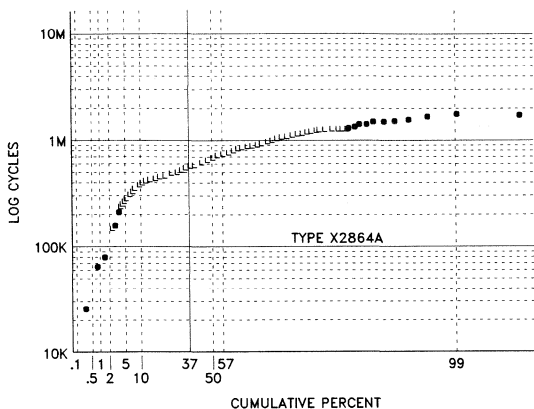
## ENDURANCE

Endurance is defined as the ability of a nonvolatile memory to withstand repeated nonvolatile data changes while remaining within specification. As is discussed in more detail in Xicor reliability report RR-510, endurance in Xicor's E<sup>2</sup>PROMs is limited by two effects, electron trapping in the tunnel

oxide and oxide breakdown. Electron trapping in the tunnel oxide is the major failure mechanism in the endurance range of more than ~ 10<sup>5</sup> data changes. Oxide breakdown tends to be the major failure mechanism for devices which have endurance of less than ~ 10<sup>5</sup> data changes.

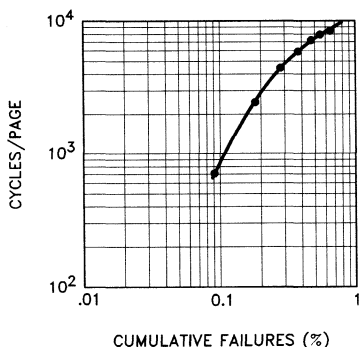
Xicor uses two tests to evaluate the endurance of its E<sup>2</sup>PROMs. One test utilizes special test modes to enable all bits in a unit to be changed simultaneously. This test is used to measure the ultimate endurance of a sample of units. For reasons discussed in RR-510, this test tends to give a somewhat pessimistic estimate of trapping limited endurance and a slightly optimistic estimate of oxide breakdown limited endurance. Figure 8 shows an endurance distribution sample from a broad range of X2864A material. In order to accurately monitor the oxide defects, which appear as infant mortality endurance failures, Xicor conducts a test in which

each page is written to 10,000 times on a page-by-page basis. Figure 9 shows the distribution of failures found from a sample of 1034 units coming from at least 10 runs. As shown in RR-510 these failures are expected to contribute approximately 10 FIT to the failure rate in typical applications.



0079-6

Figure 8: An extreme value distribution of endurance monitor on units cycled in mass mode.



0079-7

Figure 9: Cumulative failures occurring at less than 10K writes/page of complete memory for a sample of 1034 X2864A chosen from more than 10 diffusion lots.

## LIFETESTS

In addition to the endurance and data retention tests specifically targeted at properties unique to nonvolatile memories, Xicor conducts the standard battery of product life and package integrity tests.

In order to accelerate device failure rate, Xicor runs high and low temperature dynamic lifetests and a high temperature reverse bias test. High temperature dynamic lifetest accelerates the vast majority of the failure mechanisms which might effect these products. The exceptional mechanism is hot electron trapping in the gate oxide for which the worst case is at low temperature. Test pattern studies show that hot electron trapping is not expected to be a problem in the X2864A technology which uses relatively conservative transistors of 3 microns gate length and 750Å gate oxide thickness in the periphery. To verify this prediction, units were operated dynamically for 1000 hours at  $-40^{\circ}\text{C}$ . The data for this stress are exhibited in Table II and show no failures as expected.

The procedure that Xicor uses in dynamic lifetest is to load a topological checkerboard pattern into the units. The units are continuously read at temperature while the addresses are incremented in a binary sequence. At each readout the data integrity is first verified and then all parameters and functions (read and write) are verified across the specified voltage range. Finally the checkerboard pattern is reloaded and the units returned to the stress. The procedure in HTRB stress is similar except that during the stress all pins are biased high.

Package Type	Lot ID	500 Hrs.		1000 Hrs.	
		# Fail	# In	# Fail	# In
Cerdip	Q1, 2, 3	0	75	0	75
	Q4	0	25	0	25
	Q5	0	25	0	25
<b>Totals</b>		0	125	0	125

Table II:  $-40^{\circ}\text{C}$  dynamic lifetest.

The data for these stresses are exhibited in Tables III and IV. In these tables the data are segregated by package type for each of the several types tested. This data was collected over the period June 1986 through March 1987.

Package Type	Lot ID	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.	
		# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In
PDIP	Q5	3[a]	102	0	99	—	—	—	—	—	—	—	—
	Q6	0	102	0	102	—	—	—	—	—	—	—	—
	Q7	0	102	0	102	—	—	—	—	—	—	—	—
	Monitor	0	3966	0	3962	0	640	1[b]	560	—	—	—	—
PLCC	Q3	0	500	0	446	—	—	—	—	—	—	—	—
	Q4	1[c]	912	0	843	—	—	—	—	—	—	—	—
Cerdip	Q1,2,3	1[d]	4997	0	4997	0	300	0	300	0	294	0	294
	Q4	0	874	0	874	0	100	0	95	0	95	0	94
	Q5	0	1282	0	1280	0	100	1[a]	97	0	97	0	95
	Monitor	0	1498	1[a]	1492	2[a]	240	0	238	—	—	—	—
<b>Totals</b>		5	14335	1	14197	2	1380	2	1290	0	486	0	483

[a] = Ionic contamination 1.0eV

[b] = Data retention 0.6eV

[c] = Marginal  $V_{IN}$

[d] = Cracked die

Table III: 125°C dynamic lifetest.

Package Type	Lot ID	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.	
		# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In
PLCC	Q3	0	52	1[a]	52	—	—	—	—
PDIP	Q1	—	—	—	—	4[a]	25	0	21
	Q2	—	—	—	—	0	25	0	24
	Q3	—	—	—	—	0	25	0	24
Cerdip	Q1	—	—	—	—	0	45	0	45
	Q2	—	—	—	—	0	45	0	45
	Q3	—	—	—	—	0	45	0	45
	Q4	—	—	—	—	0	45	1[a]	45
	Q5	—	—	—	—	1[a]	45	0	44
<b>Totals</b>		0	52	1	52	5	300	1	293

[a] = Ionic contamination 1.0eV

Table IV: 150°C static lifetest.

## PACKAGE INTEGRITY TESTING

The tests Xicor employs to ascertain the integrity of the packages differ between hermetic and plastic encapsulated devices. For hermetic devices Xicor follows the tests specified in MIL-STD-883C, Method 5005 for group C & D evaluation of packaged devices. Tables V and VI contain the results for Cerdip and LCC packages, respectively.

For plastic encapsulated devices the military standard tests are not really applicable. Instead Xicor uses autoclave and 85/85 stresses to test for corrosion effects in the non-hermetic plastic packages.

Xicor also makes extensive use of temperature cycling to test for die cracking or lead shear which might arise as a result of the mismatch of thermal expansion coefficients which exists between the epoxy molding compound and the silicon die. The autoclave tests are conducted by storing units in steam at 2 atmospheres (15 PSIG) and 121°C. The 85/85 tests are conducted with all inputs and outputs biased at 5V. These are conducted both with  $V_{CC}$  powered and unpowered since there is some uncertainty as to which case is worst. The temperature cycling is done between -65°C and +150°C in compliance with MIL-STD-883C, method 1010, condition C. The results are exhibited in Tables VII, VIII, and IX and show very good results.

Test	Method	Conditions	LTPD	Accept #	Results
Temperature Cycling	1005	Test Condition C (10 cycles, -65°C to +125°C)	15	0/15	0/120
Constant Acceleration	2001	Test Condition E (30,000 y, Y1 axis only)			0/120
Seal	1014	Test Condition B ( $5 \times 10^{-7}$ cc/min)			1/120
—Fine		Test Condition C			0/119
—Gross					
Lead Integrity	2004	Test Condition B2 (Lead Fatigue)	15	0/15	0/60
Seal	1014	Test Condition B			0/60
—Fine		Test Condition C			1/60
—Gross					
Thermal Shock	1011	Test Condition B (15 cycles, -55°C to +125°C)	15	0/15	0/172
Temperature Cycling	1010	Test Condition C (100 cycles)			0/172
Moisture Resistance	1004				0/172
Seal	1014	Test Condition B			1/171
—Fine		Test Condition C			0/171
—Gross					
Internal Water Vapor Content	1018	5,000 ppm Maximum Water Content at 100°C	—	0/3 or 1/5	0/12
Mechanical Shock	2002	Test Condition B (1500 g peak, 3 axis)	15	0/15	0/197
Vibration Variable Frequency	2007	Test Condition A (20g peak, 3 axis)		0/15	0/197
Constant Acceleration	2001	Test Condition E		0/15	0/197
Seal	1014	Test Condition B		0/15	4/197
—Fine		Test Condition C		0/15	2/193
—Gross					
Salt Atmosphere	1009	Test Condition A	15	0/15	0/102
Seal	1014	Test Condition B			0/102
—Fine		Test Condition C			0/102
—Gross					
Adhesion of Lead Finish	2025		15	0/15 (# of leads from 3 devices)	0/45
Lid Torque	2024				0/15

Table V: Environmental test for 28-lead cerdip package.

Test	Method	Conditions	LTPD	Accept #	Results
Lead Integrity	2004	Test Condition B2 (Lead Fatigue)	15	1/15	0/45
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/45 0/45
Thermal Shock	1011	Test Condition B (15 cycles, -55°C to +125°C)	15	1/15	0/120
Temperature Cycling	1010	Test Condition C (100 cycles)			0/120
Moisture Resistance	1004				0/120
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/120 0/120
Internal Water Vapor Content	1018	5,000 ppm Maximum Water Content at 100°C	—	0/3 or 1/5	0/9
Mechanical Shock	2002	Test Condition B (1500 g peak, 3 axis)	15	0/15	0/120
Vibration Variable Frequency	2007	Test Condition A (20g peak, 3 axis)			0/120
Constant Acceleration	2001	Test Condition E			0/120
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/120 0/120
Salt Atmosphere	1009	Test Condition A	15	0/15	0/83
Seal —Fine —Gross	1014	Test Condition B Test Condition C			0/83 0/83

Table VI: Environmental test for 32-pad LCC package.

	48 Hrs.		96 Hrs.		192 Hrs.		288 Hrs.		384 Hrs.		521 Hrs.	
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In
Monitor	0	1577	0	1577	—	—	—	—	—	—	—	—
Q1	0	80	0	80	0	80	0	78	0	78	0	78
Q2	0	80	0	80	0	80	0	80	0	79	0	79

Table VII: Autoclave.

	V <sub>CC</sub> = 5.5V				V <sub>CC</sub> = 0V			
	500 Hrs.		1000 Hrs.		500 Hrs.		1000 Hrs.	
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In
Q1	0	99	0	99	0	98	0	95
Q2	0	99	0	97	0	99	0	99
Q3	0	99	0	99	0	99	0	99
Q4	0	99	0	99	0	98	0	98
Q5	0	90	0	90	0	90	—	—
Q5	0	110	0	110	0	111	0	110

Table VIII: 85/85.

Package Type	Lot ID	200 Cycles		500 Cycles		1000 Cycles	
		# Fail	# In	# Fail	# In	# Fail	# In
PDIP	Q1	0	80	0	78	1	78
	Q2	0	80	0	80	0	80
	Q3	0	78	0	78	0	78
	Q4	0	78	0	77	0	77
	Q5	0	78	0	78	0	78
	Monitor	0	623	0	623	—	—
<b>Totals</b>		0	1017	0	1014	1	391

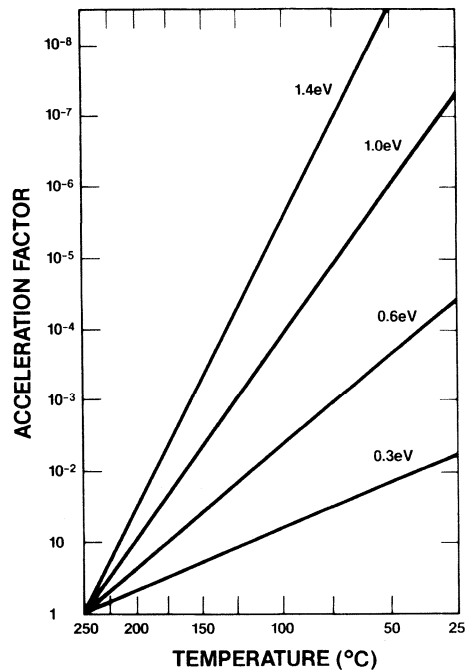
Table IX: Temperature cycle.

## FAILURE RATE PREDICTION

It has been long observed that failure rates follow a bathtub shaped curve. There is an infant mortality region characterized by a rapidly declining failure rate as “weak” parts are eliminated from the populations, a random failure region characterized by an invariant or slowly declining failure rate, and a wear-out region characterized by an increasing failure rate as the units reach end-of-life. Xicor, and most other conscientious manufacturers, designs processes so that end intrinsic wearout failures are never seen over the normal life of the part and develops manufacturing flows to minimize the number of weak parts which are produced.

The classic parameter used to accelerate failure rates is temperature. It is known that a very broad

class of failure mechanisms have a temperature dependence proportional to  $\exp(-E_a/kT)$  where  $E_a$  is called the activation energy,  $k$  is Boltzmann’s constant, and  $T$  is the absolute temperature. This is true because a number of basic physical phenomena such as diffusion rates and chemical reaction rates have this dependence. If the activation energy is known for the failure mechanisms in question, then the failure rates arising from these mechanisms can be measured at elevated temperature and extrapolated back to lower operating temperatures. The relationship which allows one to translate failure rates from one temperature to another is known as the Arrhenius relation. Figure 10 illustrates this relation for a number of common values of activation energy.



0079-8  
Figure 10: Acceleration factor vs. temperature calculated for various activation energies from Arrhenius relation.

There is no simple, one-step formula for inferring a predicted failure rate from the experimental data. Instead, the failures of each individual activation energy must be treated differently. The first step is to calculate the equivalent device hours at the ambient

Activation Energy	Device Hr. at 125°C	Equivalent Hr. at 55°C	Equivalent Hr. at 70°C	Failures	Failure Rates (FIT)			
					60% UCL 55°C	60% UCL 70°C	Best Est 55°C	Best Est 70°C
0.3eV	$5.097 \times 10^6$	$2.504 \times 10^7$	$1.716 \times 10^7$	0	36	54	28	41
0.6eV	$5.097 \times 10^6$	$1.242 \times 10^8$	$5.806 \times 10^7$	1	16	34	13	29
1.0eV	$5.097 \times 10^6$	$1.068 \times 10^9$	$2.971 \times 10^8$	4	5	17	4	15
<b>Totals</b>					57	105	45	85

Table X: Failure rate calculation.

temperature of interest, utilizing the Arrhenius relationship discussed earlier. This calculation should be carried out for every mechanism observed or expected. For example, the calculation for the 0.3eV activation energy oxide rupture mechanism should be carried out whether this failure mechanism is observed or not, since this mechanism is always anticipated in MOS integrated circuits. The extrapolation should be carried out utilizing the junction temperature at the ambient temperature of interest and not the ambient temperature itself. The upper confidence limit is then calculated for the failure rate for each activation energy. The upper confidence limits for the various activation energies are then summed for a total failure rate prediction. The meaning of the "upper confidence level" is that with a certainty, or probability, of a certain level we can say that the true value is less than the stated value. Thus, the confidence level rate calculated is non-zero even for the case where no failures are observed because we can't be sure that there will be none. This procedure is discussed in more detail in RR-506.

The infant mortality failure fraction is calculated from the 48 hour, 125°C burn-in data. This corresponds to the failure expected in the first several weeks of operating life. The data shows that 5 units failed out of 14,335 units tested for an infant failure fraction of 0.03% or 349 ppm.

The long term (random)—failure rate is estimated from the 125°C dynamic lifetest data in Table X. These calculations sum the data from all package types tested. The results show the predicted failure rate at 55°C 60% UCL to be 50 FIT (or 0.0050%/1000 Hr). One FIT is one failure in  $10^9$  hours. Even

though these calculations are based on over 5 million device-hours at 125°C, the failure rate is still dominated by the gate oxide failure mechanism which was not observed. If this mechanism were to be excluded, the predicted failure rate would drop approximately in half.

## SUMMARY

In this paper, the physical operation of Xicor E<sup>2</sup>PROMs is discussed in some detail. Data on data retention and endurance of the X2864A are presented which show that they are expected to contribute about 1 FIT and 10 FIT, respectively, to the device failure rate. Data based on dynamic lifetest is used to estimate the operating failure rate. The best estimate of the long term failure rate based on this data is 39 FIT at 55°C. The infant mortality failure fraction based on 48 hour, 125°C dynamic burn-in is 349 ppm. Data is also presented on the package integrity of this device in Cerdip, LCC, PDIP, and PLCC. The data shows the Xicor X2864A to be a very reliable device.

## REFERENCES

1. R.E. Shiner, et al, Proc. 18th Reliability Physics Symposium, pp. 238-243 (1980).
2. N. Mielke, A. Fazio and H. Liou, Proc. 25th Reliability Physics Symposium (1987).

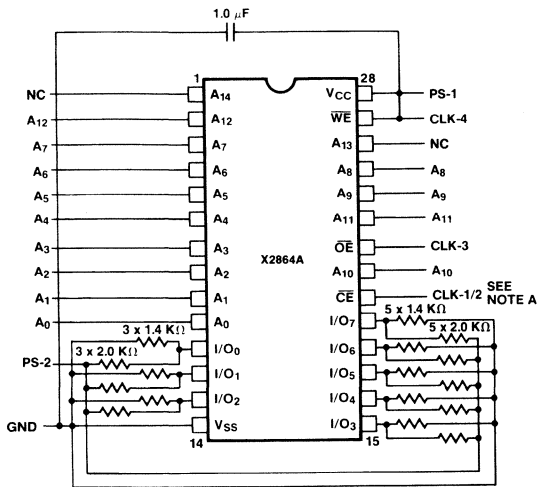
This report is based on data collected through March 1987.



# APPENDIX A

Product	Package Type					
	Plastic		Cerdip		LCC	
	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$
X2864A	39.5	64.3	16.5	35	5.0	46.0

Thermal Resistance Table:  $\theta_{JC}$  and  $\theta_{JA}$  expressed in °C per watt.



0079-12

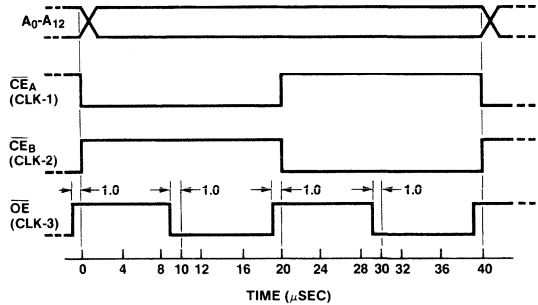
### Note A:

CLK-1: Rows 1, 3, 5 . . . (odd rows— $\overline{CE}_A$ )  
 CLK-2: Rows 2, 4, 6 . . . (even rows— $\overline{CE}_B$ )  
 Such that: CLK-2 = CLK-1

**Note B:** (1)  $\overline{WE}$  must always be hardwired to  $V_{CC}$  (Pin 28) at device as shown.

- (2) All resistors:  
1% metal film  
1/4 W
- (3) I/O pull-up: 2.00 K $\Omega$   
I/O pull down: 1.40 K $\Omega$
- (4) Socket-to-socket isolation as shown.

X2864A (DIP) Burn-in circuit.



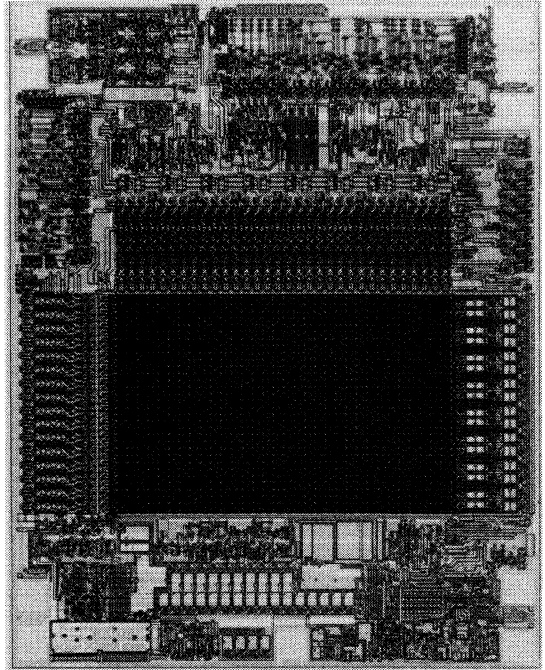
0079-13

- Notes:** (1)  $A_0$ – $A_{12}$ : binary sequencing address cycle: 40  $\mu$ s.  
 (2)  $\overline{WE}$  disabled (tied to  $V_{CC}$  at device).  
 (3)  $V_{IN}$  Low: 0.4V  $V_{IN}$  High: 5.0V  
 (4)  $V_{CC}$ : 5.50V

X2864A (DIP) Burn-in timing diagram.

---

## NOTES



0080-1

# **X2404 RELIABILITY REPORT**

**By Julie Segal**

# INTRODUCTION

The X2404 is a 4096 bit serial E<sup>2</sup>PROM organized as two 256 x 8 bit pages. This memory operates on a single 5V power supply for all operations. Figure 1 provides the pin configuration; Figure 2 shows the functional block diagram; Figure 3 illustrates the physical location of the various address bits. The thermal resistance table, burn-in circuit and a timing diagram are included in Appendix A for your reference.

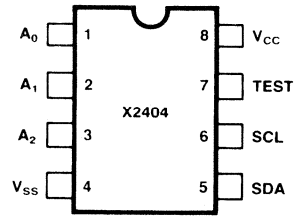


Figure 1: X2404 Pin configuration.

0080-3

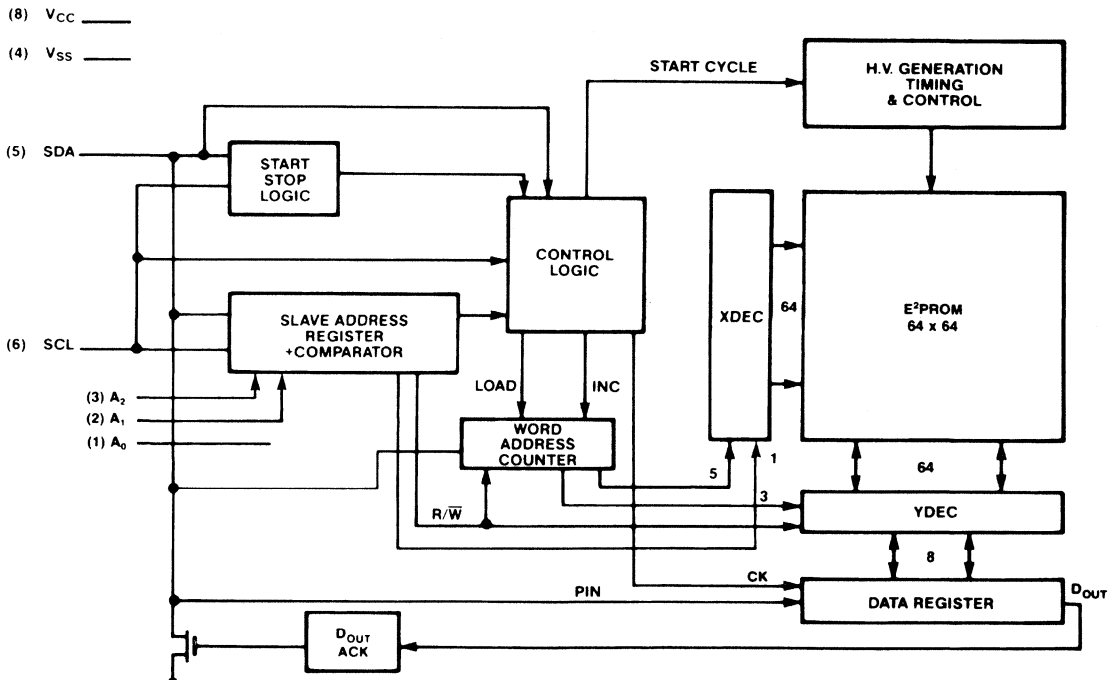
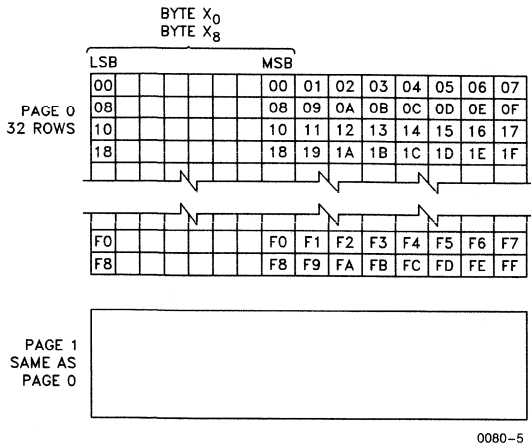


Figure 2: X2404 Functional block diagram.

0080-4



Each square equals one byte.

Figure 3: X2404 Physical bit map.

Xicor is an experienced producer of E<sup>2</sup>PROMs with over fourteen million devices in the field. This and previous experience with the development of NOVRAMs has given Xicor a leading position in nonvolatile memory technology.

## TECHNOLOGY

The X2404 is fabricated in a triple polysilicon N-channel floating gate MOS technology. Data is stored as the presence of positive or negative charge on the second level polysilicon which acts as a gate of a memory transistor. This floating gate is surrounded by ~ 750Å of thermally grown oxide, one of the best electrical insulators known. Charge is transferred to and from the floating gate through a quantum mechanical effect known as Fowler-Nordheim tunneling. This phenomenon has been described in detail in recent publications.<sup>1,2,3</sup>

## RELIABILITY STUDY AND RESULTS

The reliability studies and results presented here are those of the X2404 in a plastic package.

Before Xicor qualifies any new product it is subjected to a series of accelerated stresses and tests. These tests are designed to accelerate any degradation a device may experience over the course of a normal lifetime so as to uncover any design or process flaws.

In addition, Xicor runs ongoing monitors of those products in production. This assures high reliability standards for all product shipped by Xicor.

The stresses used to establish reliability data are as follows:

- 1) High temperature dynamic lifetest.
- 2) Data retention bake.
- 3) High temperature high voltage stress.
- 4) Environmental testing.

A short description of these tests and the results obtained are presented in the following report.

## Dynamic Lifetest

Most failure modes encountered in MOS devices are accelerated if the device is operated at elevated temperatures. Thus the dynamic lifetest aims to accelerate any failure modes a device may exhibit by operating the device in its most common mode at high temperature.

For the X2404, the dynamic lifetest consisted of continually reading the devices at a temperature of 125°C. A known pattern was stored in the devices prior to the beginning of the test. Each unit was tested for data retention and complete functionality after 48, 168, 500, 1000, 1500 and 2000 hours of dynamic lifetest.

The results of the dynamic lifetest are shown in Table I for samples pulled from five lots of plastic devices. As indicated in the table, all samples were subjected to 168 hours of burn-in. One hundred units from each sample lot were then put on continuing test, with the results as shown.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
A	0	880	0	880	0	100	0	100	0	100	0	100	$3.3 \times 10^5$
B	1[a]	1000	0	999	0	100	0	100	0	100	0	100	$3.5 \times 10^5$
C	2[a] [b]	999	1[a]	997	1[a]	100	0	97	0	97	0	97	$3.5 \times 10^5$
D	0	999	0	999	0	100	0	100	0	100	0	100	$3.5 \times 10^5$
E	0	998	0	997	0	100	0	100	0	100	0	100	$3.5 \times 10^5$
<b>Totals</b>	3	4876	1	4872	1	500	0	497	0	497	0	497	$1.7 \times 10^6$

[a] Oxide breakdown

[b] Metallization defect

Table I: Dynamic lifetest @ 125°C, test results.

## Data Retention

The purpose of this stress is to measure and ensure a device's ability to retain data. This test is run at elevated temperatures because floating gate structures will have a greater tendency to lose charge (data change) at higher temperatures. Because the X2404 cell is similar to that of the X2864A, we expect similar excellent data retention. Refer to Xicor publication, *X2864A Reliability Report*, RR-507A.<sup>4</sup>

## High Temperature High Voltage Stress

The high temperature high voltage stress test is a derivative of the high temperature reverse bias tests used to evaluate bipolar circuits. In this test  $V_{SS}$  is grounded while all inputs and  $V_{CC}$  are maintained at high voltage while being baked. The stress is intended to expose failures due to mobile ionic contaminants, electrical overstress and latent gate oxide defects. The temperature for this test is 150°C with the bias voltage set at +5.5V. Data retention and functionality were verified after 500, 1000, 1500, and 2000 hours. The results of the tests are listed in Table II.

Lot #	500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
A	0	50	0	50	0	50	0	50	$1 \times 10^5$
B	0	50	0	50	0	50	0	50	$1 \times 10^5$
C	0	50	0	50	0	50	0	50	$1 \times 10^5$
D	0	50	0	50	0	50	0	50	$1 \times 10^5$
E	0	50	0	50	0	50	0	50	$1 \times 10^5$
<b>Totals</b>	0	250	0	250	0	250	0	250	$5 \times 10^5$

Table II: 150°C High temperature high voltage test results.

## ENVIRONMENTAL TESTING

Environmental tests are designed to determine a device's resistance to extreme or changing environments. Presented here is the reliability data on plastic packaged devices.

Due to the considerable difference in expansion coefficients between plastic and silicon, plastic devices can be susceptible to temperature cycling damage. Therefore, plastic units were subjected to a more stringent test for this condition than that required for MIL-STD-883B group D testing. Table III illustrates the test results of units that had been subjected to one thousand temperature cycles as defined by MIL-STD-883 test condition C (i.e., -65°C to +150°C).

Lot #	168 Cycles		500 Cycles		1000 Cycles	
	# Fail	# In	# Fail	# In	# Fail	# In
A	0	100	0	100	0	100
B	0	100	0	100	0	100
C	0	100	0	100	0	100
D	0	100	0	100	0	100
E	0	100	0	100	0	100
<b>Totals</b>	0	500	0	500	0	500

Table III: Temperature cycling test results.

## 85°C and 85% Relative Humidity and Autoclave Tests

In addition, plastic encapsulated devices may be susceptible to moisture. For this reason five sample lots of plastic units were stressed at 85°C with 85% relative humidity (both powered and unpowered) and five additional sample lots were subjected to autoclave tests (pressure pot) at two atmospheres. These stresses test for corrosion, electrolytic failure modes and passivation integrity. The results of these tests are presented in Tables IV and V.

Lot #	168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	
A	0	50	0	50	0	49	$4.5 \times 10^4$
B	0	50	0	50	0	50	$5.0 \times 10^4$
C	0	50	1[c]	50	0	49	$4.5 \times 10^4$
D	0	50	0	50	0	50	$5.0 \times 10^4$
E	0	50	0	50	0	50	$5.0 \times 10^4$
<b>Totals</b>	0	250	1	250	0	248	$2.4 \times 10^5$

[c] Leaky oxide

Table IVA: 85/85 Test results with  $V_{CC} = +5.0V$ .

Lot #	168 Hrs.		500 Hrs.		1000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	
A	0	50	0	50	0	50	$5.0 \times 10^4$
B	0	50	0	50	0	50	$5.0 \times 10^4$
C	0	50	0	50	0	50	$5.0 \times 10^4$
D	0	50	0	50	0	50	$5.0 \times 10^4$
E	0	50	0	50	0	50	$5.0 \times 10^4$
<b>Totals</b>	0	250	0	250	0	250	$2.5 \times 10^5$

Table IVB: 85/85 Test results with  $V_{CC} = 0V$ .

**NOTE:** In both 85/85 tests, each pin was alternately biased to +5V and 0V to provide an electrical potential between adjacent metal lines on the die.

Lot #	48 Hrs.		144 Hrs.		240 Hrs.		336 Hrs.		432 Hrs.		528 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
A	0	100	0	100	0	100	0	100	0	100	0	100	$5.3 \times 10^4$
B	0	100	0	100	0	100	1[c]	100	0	99	0	99	$5.3 \times 10^4$
C	0	100	0	100	0	100	0	99	0	99	0	99	$5.3 \times 10^4$
D	0	100	0	100	0	100	0	100	0	100	0	100	$5.3 \times 10^4$
E	0	100	1[c]	100	0	99	0	99	0	99	0	99	$5.2 \times 10^4$
<b>Totals</b>	0	500	1	500	0	499	1	498	0	497	0	497	$2.6 \times 10^5$

[c] Leaky oxide

Table V: Autoclave test results.



# PREDICTION OF FAILURE RATES

As mentioned previously, accelerated testing allows one to identify possible design and process flaws. It also makes it possible to predict long term failure rates under normal operating conditions.\*

All failure mechanisms are accelerated to some degree by voltage or temperature or both. The degree to which any given failure mode is accelerated is known as the activation energy or simply as the acceleration factor. Thus knowledge of a failure mode's activation energy allows one to predict the long term failure rate for that failure mode under normal operating conditions. If the activation energy is not known it can be determined experimentally. Four typical failure mechanisms of the technology employed by Xicor and their corresponding activation energies are:

Oxide breakdown	0.3eV
Electromigration	0.55eV
Leaky oxides	0.6eV
Ionic contamination	1.0eV

Table VI contains the predicted long term failure rates for these activation energies. The results are based on the dynamic lifetest and HTRB data presented in the previous sections.

Activation Energy	Number of Failures	Equivalent Hours at 55°C	60% UCL Failure Rate Per 1000 Hrs. at 55°C	
0.3eV	2	$1.5 \times 10^7$	0.0210	
0.55eV	0	$8.6 \times 10^7$	0.0015	
0.6eV	0	$1.2 \times 10^8$	0.0008	
1.0eV	0	$2.2 \times 10^9$	0.0000	
			0.0233	<b>Total</b>

Table VI: Predicted long term failure rates.

**\*NOTE:** The infant mortality failure rate, based on 3 failures out of 4867 units tested after the first 48 hours of burn-in at 125°C is 0.06%. 48 hours of 125°C burn-in is equivalent to a few hundred to approximately 1000 hours of system operating time, depending on failure mode and system operating temperature.

The failure rates predicted are for plastic devices. The predicted failure rate in percent is depicted as the "60% upper confidence level failure rate per 1000 device hours." This means that there is a 60% probability that the actual failure rate will be below the rate calculated. Sometimes predictions are expressed in FIT units. To convert from the given values to FITs, simply multiply the failure rate per 1000 hours operation by 10,000.

A more representative value for the failure rate can be given by the best estimate. This value gives the most likely failure rate based on the given data as shown in Table VII.

Activation Energy	Number of Failures	Equivalent Hours at 55°C	B.E. Failure Rate Per 1000 Hrs. at 55°C	
0.3eV	2	$1.5 \times 10^7$	0.0158	
0.55eV	0	$8.6 \times 10^7$	0.0008	
0.6eV	0	$1.2 \times 10^8$	0.0006	
1.0eV	0	$2.2 \times 10^9$	0.0000	
			0.0172	<b>Total</b>

Table VII: Best estimate long term failure rates.

Based on these values it can be seen that the expected long term failure rate for the X2404 is 0.0172% per 1000 hours at 55°C.

## ENDURANCE

Endurance of the X2404 is generally limited to electron trapping in the tunnel oxide. Figure 4 shows the extreme value distribution observed for endurance on this part as measured by simultaneously changing all bits from a "1" state to its complement and back.



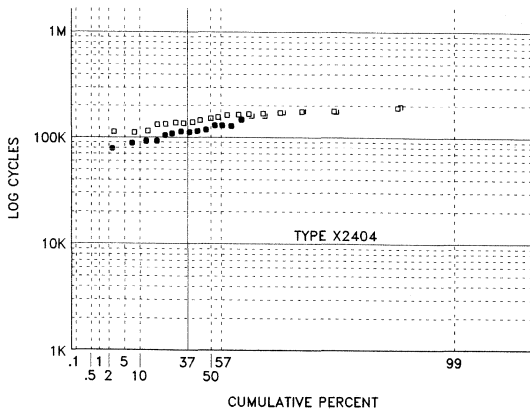


Figure 4: An extreme value distribution of endurance monitor on units cycled in mass mode.

## SUMMARY

The technology used in producing the X2404 was reviewed. A comprehensive set of data covering a variety of stresses were presented and described. Finally, failure predictions were provided.

## REFERENCES

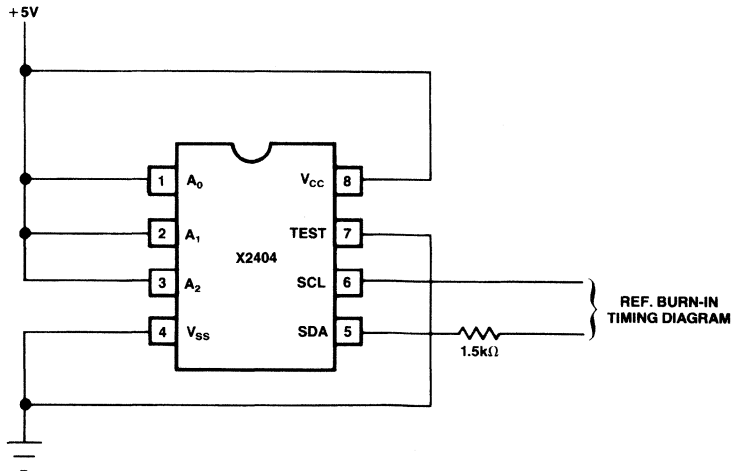
1. R.K. Ellis, *IEEE Electron Device Letters* 13 (1982): 330–333.
2. R.K. Ellis, H.A.R. Wegener and J. Caywood, *International Electron Devices Meeting Technical Digest* (1982): 749–752.
3. J. Caywood and Reliability Engineering Staff, *NOVRAM Reliability Report*, Xicor publication RR-502A (1985).
4. T. Kaysser and L. Purvis, *X2864A Reliability Report*, Xicor publication RR-507A (1987).

This report is based on data collected through May, 1986.

## APPENDIX A

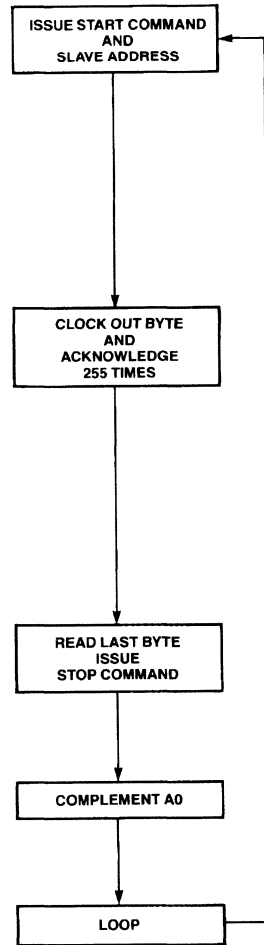
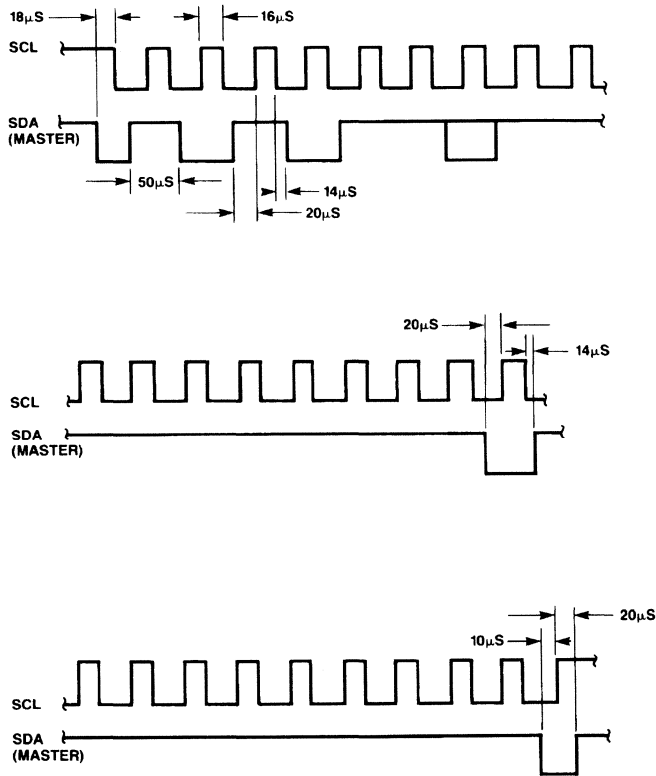
Product	Package Type: Plastic	
	$\theta_{JC}$	$\theta_{JA}$
X2404	43.0	84.0

Thermal Resistance Table:  $\theta_{JC}$  and  $\theta_{JA}$  expressed in  $^{\circ}C$  per watt.



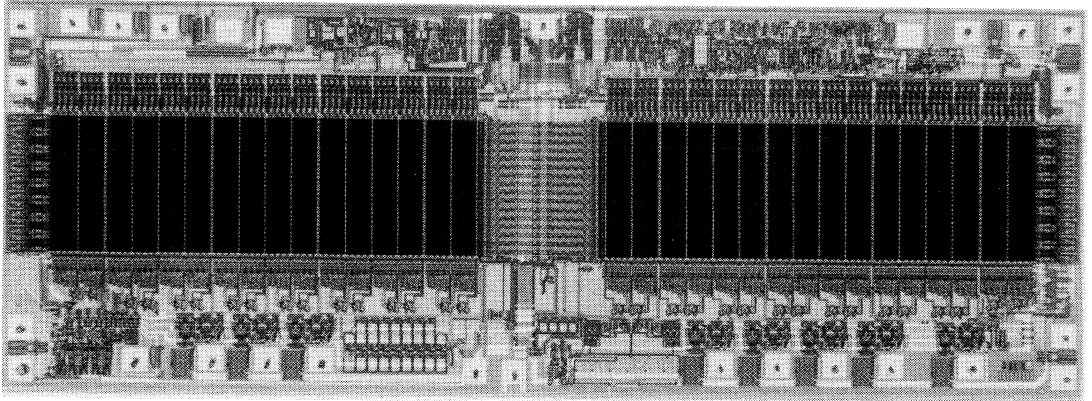
X2404 Burn-in circuit.

0080-6



X2404 Burn-in timing diagram and program flow.

0080-7



0081-1

**X2816B**  
**RELIABILITY**  
**REPORT**  
By Steven K. Fong

# INTRODUCTION

The X2816B is a 16K bit electrically erasable programmable read only memory (E<sup>2</sup>PROM) organized 2K x 8. It is an enhancement of the X2816A which incorporates DATA Polling and 16 byte page mode writing to decrease the write time needed to write data into the whole part, and it operates on a single 5V power supply for all operations. It utilizes the same proven thick oxide, textured poly technology as other Xicor nonvolatile memory products. Further information about the memory cell and tunneling physics may be found in references 1-4. Figure 1 provides the pin configuration; Figure 2 shows the functional block diagram; Figure 3 illustrates the physical location of the various address bits. The thermal resistance table, burn-in circuit and a timing diagram are included in Appendix A for your reference.

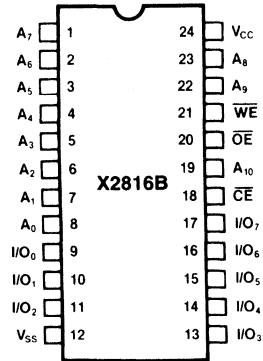
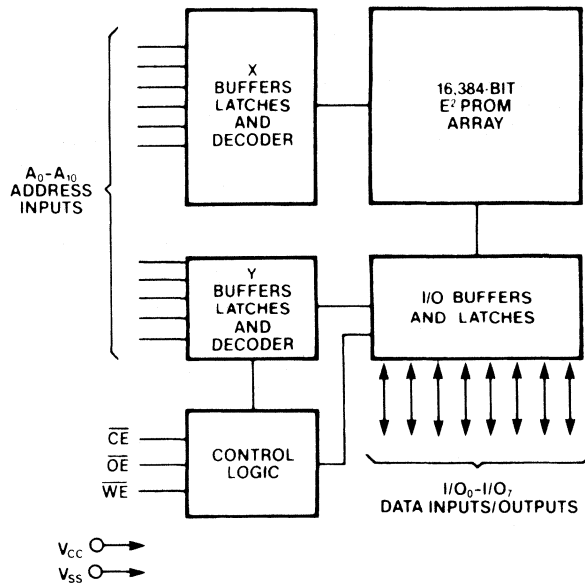


Figure 1: X2816B pin configuration.

0081-2



0081-3

Figure 2: Functional block diagram.



## Dynamic Lifestest

Most failure modes encountered in MOS devices can be accelerated if the device is operated at an elevated temperature. Thus, the dynamic lifestest aims to accelerate any failure mode a device may exhibit by operating the device in its most common mode at high temperature.

For the X2816B, the dynamic lifestest consists of continually reading a known data pattern stored in the device while it is subjected to a temperature of 125°C. Each unit was then tested for data retention and complete functionality after 168, 500, 1000, 1500 and 2000 hours of dynamic lifestest. The result of the test is shown in Table I (no failures were found).

## Data Retention

The purpose of this stress is to measure and ensure a device's ability to retain correct data. Floating gate structures are more likely to lose charge at high temperatures. For example, 48 hours at 250°C or 1000 hours at 150°C are equivalent to about 15 years at 55°C for an activation energy of 0.6eV. This is the energy for oxide defects which demonstrate floating gate memory data retention failures.

This test is conducted by storing a checkerboard pattern in the devices and baking the device at 150°C for plastic devices and 250°C for cerdip devices. The pattern is verified after 48, 168, 500, 1000, 1500 and 2000 hours. The results of this test are listed in Table II (no failures were found).

Lot #	168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 P	0	360	0	100	0	100	0	99	0	99	$2.426 \times 10^5$
2 C	0	360	0	100	0	99	0	98	0	95	$2.397 \times 10^5$
3 C	0	360	0	100	0	100	0	100	0	100	$2.435 \times 10^5$
4 C	0	280	0	0	0	0	0	0	0	0	$4.704 \times 10^4$
<b>Totals</b>	0	1360	0	300	0	299	0	297	0	294	$7.729 \times 10^5$

Note: C = Cerdip  
P = Plastic

Table I: Dynamic lifestest at 125°C test results.

Lot #	48 Hrs.		168 Hrs.		500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 P	0	20	0	20	0	20	0	20	0	19	0	19	$3.9 \times 10^4$
1 C	0	30	0	30	0	30	0	30	0	30	0	30	$6 \times 10^4$
2 C	0	50	0	50	0	50	0	50	0	50	0	50	$1 \times 10^4$
3 C	0	50	0	50	0	50	0	50	0	50	0	50	$1 \times 10^4$
<b>Totals</b>	0	150	0	150	0	150	0	150	0	149	0	149	$1.19 \times 10^5$

Note: C = Cerdip  
P = Plastic

Table II: Retention bake test results, 250°C for cerdip devices and 150°C for plastic devices.

Lot #	500 Hrs.		1000 Hrs.		1500 Hrs.		2000 Hrs.		Total Hours
	# Fail	# In	# Fail	# In	# Fail	# In	# Fail	# In	
1 P	0	10	0	10	0	10	0	7	$1.85 \times 10^4$
1 C	0	35	0	35	0	35	0	35	$7 \times 10^4$
2 P	0	7	0	7	0	7	0	7	$1.4 \times 10^4$
2 C	0	38	0	38	0	38	0	38	$7.6 \times 10^4$
3 C	0	45	0	45	0	45	0	45	$9 \times 10^4$
<b>Totals</b>	0	135	0	135	0	135	0	132	$2.68 \times 10^5$

Note: C = Cerdip  
P = Plastic

Table III: 150°C high temperature high voltage test result.

## High Temperature High Voltage Stress

The high temperature high voltage stress is intended to expose failures due to mobile ionic contaminants, electrical overstress and latent gate oxide defects. In this test,  $V_{SS}$  is grounded while all inputs and  $V_{CC}$  are maintained at high voltage.

The temperature for this test is 150°C with the bias voltage set at +5.5V. Data retention and complete functionality were verified after 500, 1000, 1500 and 2000 hours. The result of the test is listed in Table III (no failures were found).

## Environmental Testing

Environmental testing is designed to determine a device's resistance to extreme or changing environment. Due to the inherent differences between plastic and cerdip devices, different reliability stresses are applied to evaluate the individual package types.

Some of the tests used to evaluate cerdip packages, such as hermeticity, internal water vapor content, and lid torque, do not apply because the plastic packages are not hermetically sealed. (For reliability data on the 24-pin cerdip package, see the X2816A/X2804A Reliability Report RR-505).

Other tests, such as vibration and acceleration, do not apply because the die in a plastic package is completely embedded in plastic and is not susceptible to such mechanical failure. Plastic packages may be susceptible to other failure modes. Due to the considerable difference in expansion coefficients between plastic and silicon, plastic devices are considerably more susceptible to temperature

failures. Table IV shows the result of units subjected to one thousand temperature cycles as defined by MIL-STD-883 test condition C.

Lot #	250 Cycles		500 Cycles		1000 Cycles	
	# Fail	# In	# Fail	# In	# Fail	# In
1 P	0	78	0	78	0	78
2 P	0	78	0	78	0	78
3 C	0	78	0	78	0	77
<b>Totals</b>	0	234	0	234	0	233

Note: C = Cerdip  
P = Plastic

Table IV: Temperature cycling test results.

## Prediction of Failure Rates

Accelerated testing identifies possible design and process flaws. It also predicts failure rates under normal operating conditions. Most failure mechanisms in this report are accelerated by voltage, temperature or both. The degree to which any given failure mode is accelerated may be predicted by activation energy. If the activation energy is not known, it can be determined experimentally. Four typical failure mechanisms of Xicor technology and their corresponding activation energies are:

- 1) Oxide Breakdown 0.3eV
- 2) Electromigration 0.55eV
- 3) Leakage Oxide 0.6eV
- 4) Ionic Contamination 1.0eV

Table V presents the predicted failure rates for these activation energies. The results are based on the test data presented in Tables I and III.

Activation Energy	Number of Failures	Equivalent Hours at 70°C	60% UCL Failure Rate per 1000 Hours at 70°C	Equivalent Hours at 55°C	60% UCL Failure Rate per 1000 Hours at 55°C
0.3eV	0	$4.495 \times 10^6$	0.0205	$6.986 \times 10^6$	0.0132
0.55eV	0	$1.626 \times 10^7$	0.0056	$3.659 \times 10^7$	0.0025
0.6eV	0	$2.206 \times 10^7$	0.0042	$5.130 \times 10^7$	0.0018
1.0eV	0	$1.914 \times 10^8$	0.0005	$8.184 \times 10^8$	0.0001
<b>Totals</b>	0		0.0308		0.0176

Table V: 60% UCL failure rate predictions.

The failure rate predictions presented here are for both plastic and cerdip devices. Such predictions are valid because all the failure modes found or expected are common for both plastic and cerdip devices. Xicor has defined failure rate as the "60% upper confidence level" failure rate per 1000 device hours. This means that there is a 60% probability the actual failure rate will be below the rate computed. Sometimes predictions are expressed in FIT units. To convert from the previously named value to FIT, multiply by 10,000. For a more detailed discussion on confidence limits and reliability failure rate calculations, see Xicor Reliability Report RR-506.

A more representative value for the failure rate can be given by the "best estimate". This value gives the most likely failure rate based on the given data. Table VI presents the best estimate values.

Table VI shows that the expected failure rate for the X2816B is 0.0229% per 1000 hours at 70°C

which is 229.0 FIT and 0.0134% per 1000 hours at 55°C which is 134 FIT. Since no failure was observed in any of the accelerated lifetests, the failure rate calculated above should be considered an upperbound which is limited by the size of the database.

## Endurance

Endurance of the X2816B is generally limited by trapping of electrons in the tunnel oxide during tunneling as discussed in RR-510. Figure 5 shows the distribution observed for endurance on this part as measured by simultaneously changing all bits from one state to its complement and back. Additionally, a sample of 510 units had the data in every bit altered 10,000 times on a page by page basis. The results showed a failure rate of 1% in the first 10,000 cycles.

Activation Energy	Number of Failures	Equivalent Hours at 70°C	Best Estimate Failure Rate per 1000 Hours at 70°C	Equivalent Hours at 55°C	Best Estimate Failure Rate per 1000 Hours at 55°C
0.3eV	0	$4.495 \times 10^6$	0.0151	$6.986 \times 10^6$	0.0100
0.55eV	0	$1.626 \times 10^7$	0.0042	$3.654 \times 10^7$	0.0019
0.6eV	0	$2.206 \times 10^7$	0.0032	$5.130 \times 10^7$	0.0014
1.0eV	0	$1.914 \times 10^8$	0.0004	$8.184 \times 10^8$	0.0001
<b>Totals</b>	0		0.0229		0.0134

Table VI: Best estimate failure rate predictions.



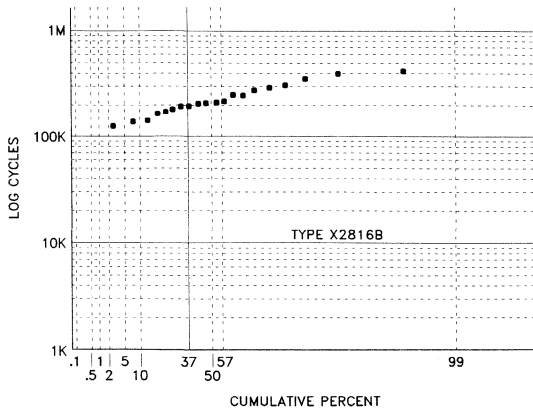


Figure 5: An extreme value distribution of endurance monitor on units cycled in mass mode. 0081-5

## SUMMARY

Data presented in this report shows that the X2816B is highly reliable. Further data is being collected to better predict the failure rates for this part.

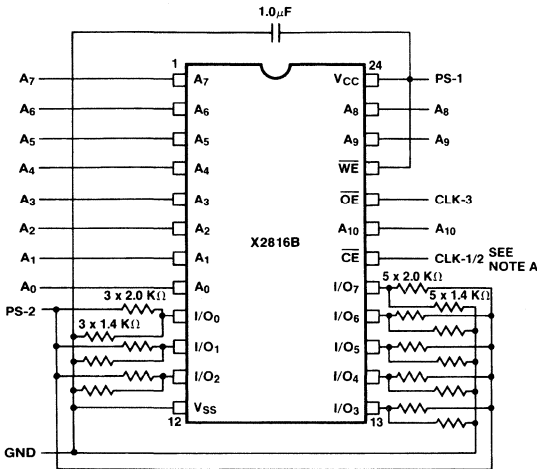
## REFERENCES

1. J. Caywood, NOVRAM Reliability Report, Xicor Publication RR-502A (1985).
2. R.K. Ellis, H.A.R. Wegener and J. Caywood, "Electron Technology in Non-Planar Floating Gate Memory Structure", 1982 IEDM Digest, pp. 749-752.
3. S.K. Lai, V.K. Dham and D. Guterman, "Comparison and Trends in Today's Dominant E<sup>2</sup> Technologies", 1986 IEDM Digest, pp. 580-583.
4. D. Guterman, B. Houck, L. Starnes and B. Yeh, "New Ultra-High Density Textured Poly-Si Floating Gate E<sup>2</sup>PROM Cell", 1986 IEDM Digest, pp. 826-828.

# APPENDIX A

Product	Package Type					
	Plastic		Cerdip		LCC	
	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$	$\theta_{JC}$	$\theta_{JA}$
X2816B	50.0	81.0	20.5	36.0	—	—

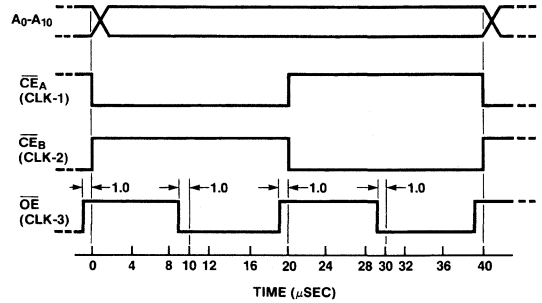
Thermal Resistance Table:  $\theta_{JC}$  and  $\theta_{JA}$  expressed in °C per watt.



0081-6

- Notes:** (A) CLK-1: Rows 1, 3, 5 . . . (odd rows— $\overline{CE}_A$ )  
 CLK-2: Rows 2, 4, 6 . . . (even rows— $\overline{CE}_B$ )  
 Such that: CLK-2 =  $\overline{CLK-1}$
- (B) 1.  $\overline{WE}$  must always be hardwired to  $V_{CC}$  (Pin 24) at device as shown.
- All resistors:  
1% metal film  
1/4 W
  - I/O pull-up: 2.0 K $\Omega$   
I/O pull-down: 1.4 K $\Omega$
  - Socket-to-socket isolation as shown.

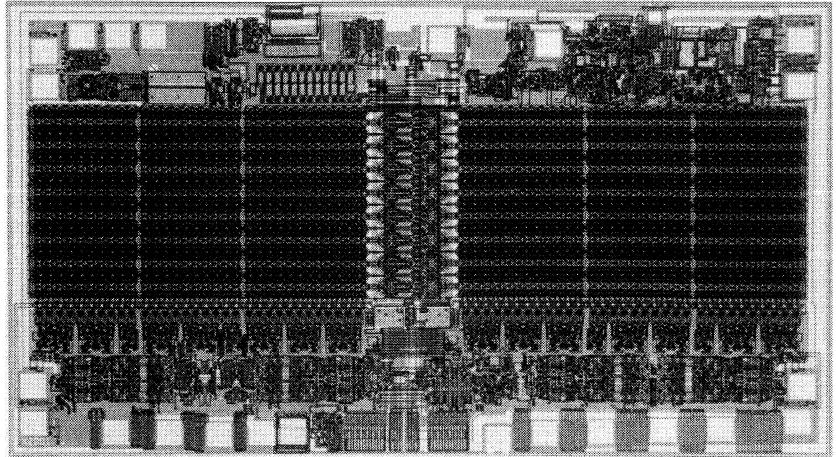
X2816B (DIP) Burn-in circuit.



0081-7

- Notes:** (1)  $A_0-A_{10}$ : binary sequencing address cycle: 40  $\mu$ s.  
 (2)  $\overline{WE}$  disabled (tied to  $V_{CC}$  at device).  
 (3)  $V_{IN}$  Low: 0.4V  $V_{IN}$  High: 5.0V  
 (4)  $V_{CC}$ : 5.50V

X2816B (DIP) Burn-in timing diagram.



0082-1

# **ENDURANCE OF NONVOLATILE MEMORIES**

**By John Caywood**

## INTRODUCTION

What is endurance? A precise definition is that endurance is the ability of a nonvolatile memory to withstand repeated data alteration while all parameters remain in specification. The end of endurance life is when any parameter fails specification as a result of data alteration. Note that although this article is specifically addressed to NOVRAMs\* and E<sup>2</sup>PROMs, this definition equally applies to a floppy disk which loses data as a result of mechanical wear of the head riding on the rotating disc. It is not always recognized that other nonvolatile memory technologies also may have limited endurance.

In the following sections the physical mechanisms which limit the endurance of E<sup>2</sup>PROMs are discussed. Then the methods which may be used to characterize and monitor the effects of these mechanisms are reviewed and the impact of endurance on device reliability is examined.

## PHYSICAL BASIS OF ENDURANCE LIMITATION

Specifically considering floating gate E<sup>2</sup>PROM technologies, why is the endurance limited? All these technologies depend upon applying a field across a dielectric in a memory cell so that electrons are injected into the dielectric by Fowler-Nordheim tunneling. These electrons drift across the dielectric and charge or discharge the floating gate in order to change the state of the cell. During this process some small portion of the electrons crossing the dielectric may become trapped. This trapped charge generates a field which retards further charge transfer. After a very large number of data changes the retarding field becomes large enough to inhibit further charge transfer. Additionally, the field that is applied stresses the dielectric and may lead to time dependent dielectric breakdown.

Which of these two effects dominates depends on the details of the technology utilized. There are two dominant technologies being utilized to manufacture commercially available E<sup>2</sup>PROMs. One, called FLOTOX, depends on tunneling across a thin (approx. 100Å) dielectric lying between two parallel silicon surfaces for charge transport. The second depends on local field enhancement near the surface of a poly silicon film to inject electrons into the conduction band of a relatively thick (~ 600Å–1000Å) dielectric. Once injected into the dielectric, the electrons drift across under lower fields existing

in the bulk of the dielectric. The enhanced fields at the poly silicon surface are a result of small bumps on the surface of the poly, and this technology is called the textured poly technology. (See references 1–3 for more detailed discussions.)

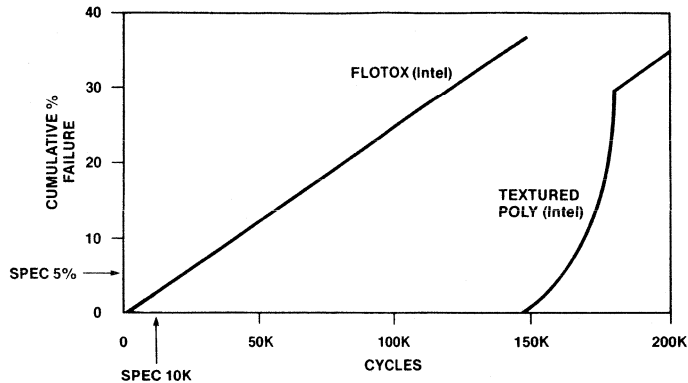
Electrons are less likely to become trapped while drifting across the thinner FLOTOX dielectric than the thicker oxide of the textured poly approach. On the other hand, the entire FLOTOX dielectric experiences the field which exists only at the surface of the textured poly oxide with the result that the FLOTOX approach is more susceptible to dielectric breakdown.

Let's look at the implications of the various failure mechanisms for product reliability. To do so, it helps to be familiar with the appropriate statistical distributions. The motivation for looking at statistical distributions arises from the fact that few users are affected by the behavior of a typical bit of E<sup>2</sup>PROM memory. Rather, what affects the user is the behavior of the worst bit in an array because the failure of the first bit defines the endurance of the memory chip. Furthermore, the user is also concerned with the distribution of endurance of the memories over a number of memories in a system or over a number of memories in a number of systems.

Figure 1 shows data published recently comparing the distribution of first failures on FLOTOX based memory arrays to the distribution of first failures on memory arrays fabricated with textured poly technology.<sup>4</sup> This data shows that the textured poly material has a low failure rate until an endurance level of a few hundred thousand cycles is reached. After this, the endurance failure fraction increases rapidly. This is because there is a low extrinsic failure rate for oxide defects in this technology. The rapid increase in failure fraction occurring in the few hundred thousand write cycle range occurs because of electron trapping in the oxide which is an intrinsic property and which has a fairly tight distribution. The FLOTOX technology material exhibits a continuously increasing failure fraction beginning at a low endurance level. This is a manifestation of the extrinsic oxide failure rate which dominates the FLOTOX endurance failures and which has a wide distribution.

Clearly, a user would be better off with the textured poly material according to this data as long as the application requires less than a few hundred thousand endurance cycles. A further, although less obvious, advantage of the textured poly approach is that because the oxide trapping rate is an intrinsic parameter, it is easily measurable and can be

\*NOVRAM is Xicor's nonvolatile static RAM device.



0082-2

Figure 1: Endurance of two E<sup>2</sup> technologies. FLOTOX and textured poly processed at Intel (16K arrays).

controlled like any other process parameter such as transistor threshold. An extrinsic parameter like oxide breakdown, on the other hand, is more difficult to measure and control because it depends upon random defects in the tunneling oxides.

To examine in more detail the endurance of Xicor's nonvolatile memory products, all of which employ textured poly technology, we must look at a statistical distribution. The distribution of interest is that of the lowest endurance bit in each memory array in a collection of arrays. In other words, we seek the distribution of the endurance of a group of memory chips. Statisticians have worked out the detailed properties of this distribution which is called the extreme value distribution. (This distribution and its application to endurance is detailed in reference 5.) If a sample is chosen from a uniform distribution (i.e., a distribution with a single uniform endurance limiter), the endurance data will fall on the straight line when plotted on an extreme value plot as is illustrated in Figure 2.

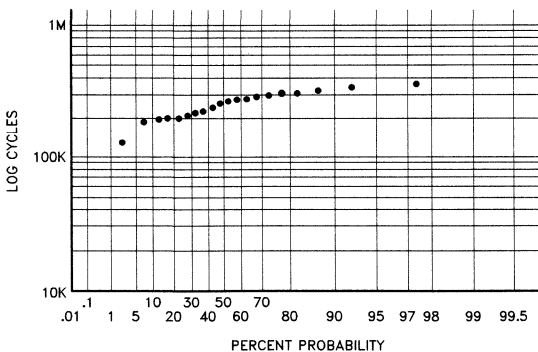


Figure 2: Extreme value distribution plot for a lot of X2004.

0082-3

Knowing the endurance distribution for a sample from a population doesn't determine the endurance of another unit chosen from the population because the endurance of the unit chosen may lie with some probability anywhere along the established distribution. However, one may say that another sample of adequate size from the population will fall on the distribution already established with high probability.

## ENDURANCE MEASUREMENTS

Up to this point the focus has been on effects which are generic to floating gate nonvolatile memory technology without much concern for how this technology is used in a memory or what system application requires the device to do. Let's now examine the more application specific aspects of endurance. A primary division lies between whether the technology is applied to NOVRAMs or E<sup>2</sup>PROMs.

Let's first examine the case of E<sup>2</sup>PROMs. Measurement of E<sup>2</sup>PROM endurance is hindered by the long times which are frequently needed in order to induce a failure. For example Xicor's X2864A has 512 pages of 16 bytes each. To write each page ~ 500,000 times needed to cause an endurance failure on a typical part at 10 ms/page write takes over four weeks. If a part is only a little bit better so that it survives a million writes (a not uncommon event) over eight weeks is needed to monitor the endurance of a lot writing a page at a time. To overcome this difficulty most memory suppliers design special test modes into a part to allow all bits to be altered in one write event. Thus, it is possible for Xicor to change all bits from one state to its

opposite and back again on its E<sup>2</sup>PROMs and thus dramatically reduce the time necessary to collect monitor data on the E<sup>2</sup>PROMs. Xicor refers to this as mass mode endurance cycling.

Because the entire part in mass mode cycling is being altered in one write cycle, the on chip charge pumps see much heavier capacitive loading. This loading causes both the voltage ramp rate and the maximum write voltage to decrease. This means that devices cycled in mass mode see less voltage stress and so have a smaller probability of failing for oxide breakdown than units cycled in page mode. However, the lower maximum level of the write voltage means that units will fail for trap up earlier in mass mode cycling than in page mode cycling because a smaller amount of trapped oxide charge is needed to inhibit writing from the lower write voltage. Thus, mass mode cycling data is a compromise which gives a pessimistic view of oxide trapping endurance limitation and an optimistic view of oxide breakdown endurance limitation.

Time dependent breakdown shows a declining failure rate with time. Because of this it would be expected that the oxide breakdown failure rate would decline with the number of write cycles. Xicor has observed this to be true for its E<sup>2</sup>PROMs and, therefore, supplements the mass mode monitor data with data on failures in the first 10,000 writes per page taken on a page write basis.

Figures 3 and 4 show the mass mode and page mode endurance data, respectively, for the Xicor X2864A, an 8K x 8 E<sup>2</sup>PROM. As can be seen from Figure 4, a large number of parts must be page write cycled to generate a data base. To find the seven failures displayed here, 1034 units representing a large number of fab lots were exposed to this test. Data for other of Xicor's products are found in the reliability reports for those products.

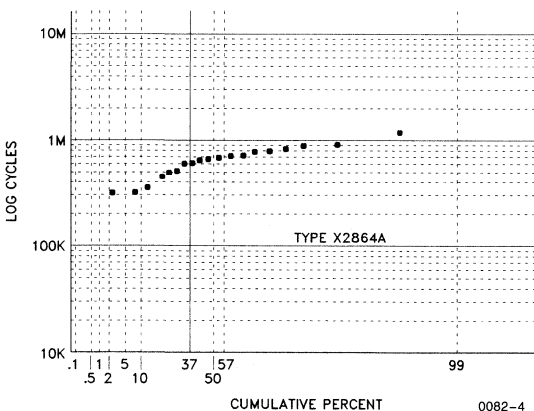


Figure 3: Mass mode cycling data for X2864A.

0082-4

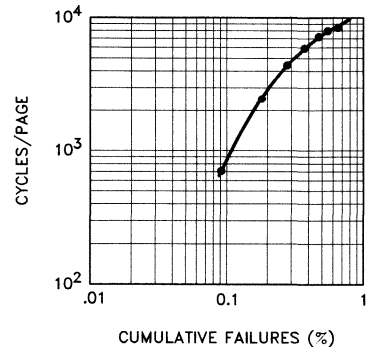


Figure 4: Page mode cycling data for X2864A.

0082-5

In Xicor NOVRAMs, data is written to all nonvolatile elements in every store cycle. However, charge passes through the tunnel oxide only when the data in a bit changes.<sup>6</sup> That is why the endurance limit of Xicor NOVRAMs is stated in terms of data changes/bit. In certain applications the user can take advantage of this. For example in a counter application, if the counter is implemented using binary code the memory element containing the least significant bit changes at each count. On the other hand if the counter is implemented using a gray code, the non-volatile data changes are more uniformly distributed over the memory and the effective endurance can be increased about four times.

From the viewpoint of characterizing the endurance, the task is straight-forward. In the general case the user can change all bits at once so the manufacturer has only to store complementary data patterns sequentially such as alternating checkerboard with inverse checkerboard. Xicor routinely monitors its NOVRAMs by this technique. The results are to be found in the individual reliability reports. Figure 2 is an example of the endurance data from a lot of X2004s (a 512 x 8 bit NOVRAM).

## CALCULATION OF RELIABILITY RATES

The real question with endurance failures is how they affect reliability of E<sup>2</sup>PROMs when they are used in systems. The usual way of dealing with this question is to calculate the failure rate for a component. The endurance contribution to the component failure rate is given by

$$f.r. (end) = ff(10K) \cdot F \cdot \bar{N} \cdot 1.142$$

---

where  $ff(10K)$  is the fraction of the units failing in 10,000 data changes,  $F$  is the fraction of the memory being altered,  $N$  is the number of times the average part in the average system is changed in 10 years for the application under consideration and 1.142 is a numerical constant to express f.r. (end) in FITs.

Let's work out some examples. Suppose that an application requires all data in the average X2864A to be changed once a day for 10 years. Then  $F = 1$ ,  $\bar{N} = 3650$ ,  $ff(10K) = 0.0067$  and f.r. (end) = 28 FIT.

Another example might be a system in which 10% of the data in an average X2864A is changed 10,000 times over a ten year period. In this case  $F = 0.1$ ,  $\bar{N} = 10,000$ ,  $ff(10K) = 0.0067$  and f.r. (end) = 7.7 FIT.

A final example is a system in which the X2864A is used to hold parameters to setup process control equipment. During setup of the equipment the parameters in 10% of the memory are adjusted 1000 times and the remainder are adjusted 100 times. Over the 10 year life the active 10% of the parameters are adjusted once a month and the less active parameters are adjusted once a year to compensate for wear. Then

$$\begin{aligned} \text{f.r. (end)} &= [0.1 \bullet 1120 \bullet 0.0067 + 0.9 \\ &\quad \bullet 112 \bullet 0.0067] \cdot 1.142 \\ &= 1.6 \text{ FIT} \end{aligned}$$

Every application is different, but with this formula and the data contained for each product in Xicor reliability reports the user should be able to easily calculate the reliability impact of endurance limitation.

## SUMMARY

In this report the physical basis of the endurance limitations of nonvolatile memories is discussed. The statistical basis for the measurements used in evaluation of endurance is reviewed. Finally, some examples of reliability calculations for nonvolatile memories are calculated for the Xicor X2864A which show that in typical applications endurance failures contribute  $\sim 10$  FIT to the failure rate.

## REFERENCES

1. S.K. Lai, V.K. Dham, and D. Guterman, International Electron Device Meeting Technical Digest, pp. 580-583 (1986).
2. R.K. Ellis, IEEE Electron Device Letters, EDL-13, pp. 330-333 (1982).
3. R.K. Ellis, H.A.R. Wegener and J. Caywood, International Electron Device Meeting Technical Digest, pp. 749-752 (1982).
4. N. Mielke, A. Fazio, H. Liou, 25th International Reliability Physics Symposium (1987).
5. H.A.R. Wegener, Xicor Reliability Report RR-504 (1984).
6. Y. Drori, International Solid-State Circuits Conference Technical Digest, pp. 148-149 (1981).

---

## NOTES



# DETERMINING SYSTEM RELIABILITY FROM E<sup>2</sup>PROM ENDURANCE DATA

By Richard Palm

Xicor has published numerous reliability reports regarding data retention and endurance; however, the relationship of this data to system reliability warrants further analysis and discussion. This paper will discuss two methods for determining the affect of endurance on system reliability. The first method will use actual data collected on the X2816A and the second method will use data collected on the X2864A.

## Definition of Terms

Endurance - is the ability of a nonvolatile memory to sustain repeated data changes.

Endurance Failure (Level) - is the limit of endurance, expressed in number of write cycles, when the *first bit* of any memory device or memory system is found to be in error after a required data change.

Write Cycle - to reduce testing time Xicor uses a test method whereby the entire array of the device under test is written in a single write cycle. Therefore, all references to "write cycle" equate to every bit in the entire array (device or system array) being written.

Cumulative Failure (Probability) - the percentage of parts not expected to attain a particular goal; i.e., endurance level.

Note: all endurance data used in this report were collected at a cycling frequency of one cycle per 100ms and at +25°C.

## Background

There are three reliability categories for nonvolatile memories: semiconductor, data retention and endurance.

- Semiconductor reliability pertains to several failure modes common to all semiconductor devices such as oxide rupture and micro-cracks.

- Data retention refers to the capability of a non-volatile memory device to retain valid data under worst case conditions.
- Endurance is the ability of a nonvolatile memory device to sustain repeated data changes.

Xicor reliability reports, RR502A and RR504, detail these three categories for Xicor devices. Reliability is easily deduced for semiconductor failures and data retention. The affect of endurance on reliability is not so straightforward.

Because endurance screening is a destructive procedure, Xicor performs endurance life tests on a sample basis. The data collected from these tests are then plotted onto an extreme value distribution graph to determine the endurance distribution for a particular lot of devices.

## Using the Extreme Value Distribution Data

Figure 1 is an extreme value distribution graph for twenty X2816A devices and Table 2 (located on the last page) is the raw data used to generate the straight line shown.

- In this sample lot the lowest ranked device (#1) exceeded 279,000 write cycles before the first bit failure occurred; however, the graph extends to the left to show that only ~ .01% of all devices from this manufacturing lot will fail before 200,000 cycles.
- The maximum of the extreme value distribution occurs at the 37% cumulative probability point (statistically, 37% of all devices will fail to reach this endurance level), indicating that the predicted most probable endurance of devices in this lot is 460,000 cycles.

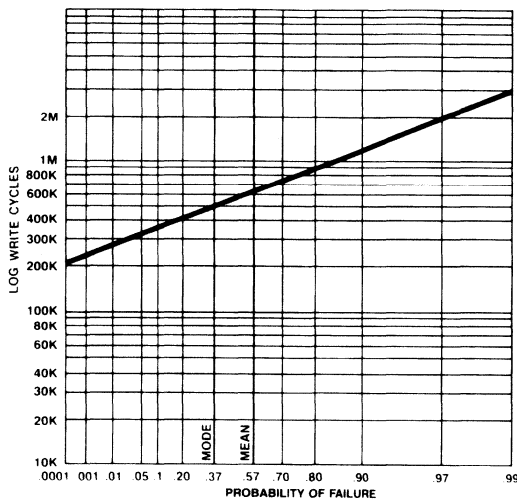


Figure 1: Extreme Value Distribution Graph for One Twenty Piece Lot of X2816As

Reliability data are generally stated in terms of percent failures per 1000 hrs. This can be easily derived from the extreme value graph in a two step procedure.

The system design parameters for this example are chosen as follows: the lifetime of the system is five years; and each X2816A will experience 250,000 write cycles over the lifetime of the system.

- The first step determines the failure rate per 1000 write cycles using the formula  $W = C/E$  where:
  - $W$  = failure rate in %/1000 write cycles
  - $E$  = endurance level chosen for the system (250,000 write cycles) divided by 1000.
  - $C$  = cumulative failure rate at  $E$  (in this case .5%).
 Therefore  $W = .5\%/250 = .002\%/1000$  write cycles.
- Converting this to percent failures per 1000 hours requires  $H = W \times A$  where:
  - $H$  = failure rate in %/1000 hrs.
  - $W$  = failure rate in %/1000 write cycles
  - $A$  = number of write cycles per hour. (i.e.,  $2.5 \times 10^5$  cycles/5 years)

In our case,  $H = .002 \times 5.7 = .0114\%/1000$  hrs.

In the above example the entire X2816A is being rewritten at the rate of 5.7 times every hour. In some applications this could occur, but generally the frequency is much lower. Using the same graph and arbitrarily choosing the lowest cumulative failure rate depicted at 200,000 write cycles and performing the same calculations, the percent failures per 1000 hrs. drops dramatically.

$$W = .01/200 = .00005\%/1000 \text{ write cycles}$$

$$H = .00005 \times 4.56 = .00022\%/1000 \text{ hrs.}$$

## Predicting System Endurance Reliability Within Design Constraints

This next example is based on data collected on the X2864A. The system requirements for which the data were collected are defined as follows: the life expectancy of the system is ten years; the number of write cycles is 10,000. Therefore, Xicor cycled five lots of approximately three hundred devices each, for 10,000 write cycles. The data were collected by cycling the devices every 100ms at  $\sim 25^\circ\text{C}$ . Table 1 summarizes the data collected.

LOT #	# OF UNITS	# OF FAILURES	% FAILURES
1	297	4	1.35
2	295	2	0.68
3	295	4	1.36
4	298	6	2.01
5	299	6	2.01
TOTAL	1484	22	1.48

Table 1: Raw Data From Cycling X2864A Devices 10,000 Times

The overall failure rate of devices unable to reach 10,000 write cycles is 1.48%. How does this relate to system reliability?

- The system is defined as having a life expectancy of ten years or  $87.6 \times 10^3$  hours.
- The failure rate in percent per 1000 hours is determined by dividing the percent of parts unable to reach 10,000 write cycles by system's life expectancy in thousands of hours.

Therefore, reliability based on endurance for this system is:

$$1.5\%/87.6 = 0.017\%/1000 \text{ hrs.}$$

## Temperature

RR504 describes in detail the effect of temperature on endurance. In general, this report shows that for every 50°C rise in temperature the endurance rate doubles. The data collected for the above examples was taken at +25°C. Therefore, for systems operating at a more common +40°C the endurance will improve. Figure 2 illustrates the case for the X2816A.

- The line labeled +25°C is the same as that in Figure 1.
- The added line is for the predicted increase in endurance at +40°C.
- The cumulative failure rate at 250,000 write cycles moves from .5% to less than .01% and the endurance reliability increases as follows:  
 $W = .01\%/250 = .00004\%/1000 \text{ write cycles}$   
 $H = .00004\% \times 5.7 = .0002\%/1000 \text{ hrs.}$

The failure rate for the X2864A sample lots can be expected to decrease by a factor of ~ 1.30, for the increase in operating temperature from +25°C to +40°C; yielding a failure rate of .013%/1000 hrs. vs. the unfactored .017%/1000 hrs.

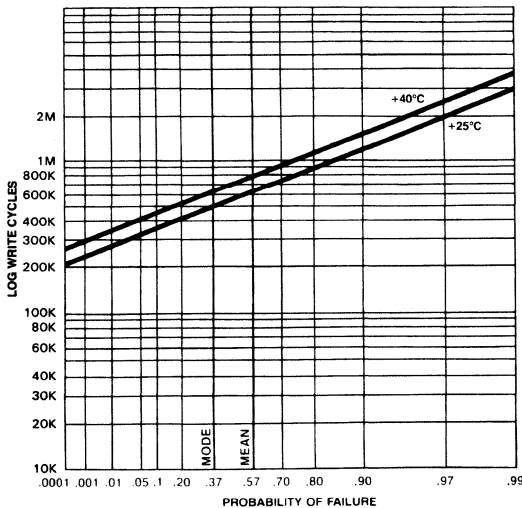


Figure 2: Affect of Ambient Temperature on Endurance

## Frequency of Writing

Xicor reliability report RR504 describes device operation and the affects of frequency of writing to a device. Figure 3 is a copy of a graph in RR504, depicting the relationship of write cycle frequency on the endurance of a Xicor nonvolatile memory.

There are two key relationships illustrated by the graph in Figure 3.

- As the frequency of writing decreases the slope of the plotted line, the extreme value, decreases.
- Although the most probable endurance (the 37% cumulative failure point) does not show appreciable change, the decreasing slope is significant in the region most concerned with predicting reliability, the .01% to 5% region (shaded area of Figure 3).

It is in this region that a system's reliability is determined. Arbitrarily choosing the .1% probability of failure point, Figure 3 shows:

- A write cycle frequency of 1 per 100 seconds increases the endurance level by a factor of 2 over a write cycle frequency of 1 per 100 milliseconds.

0018-5

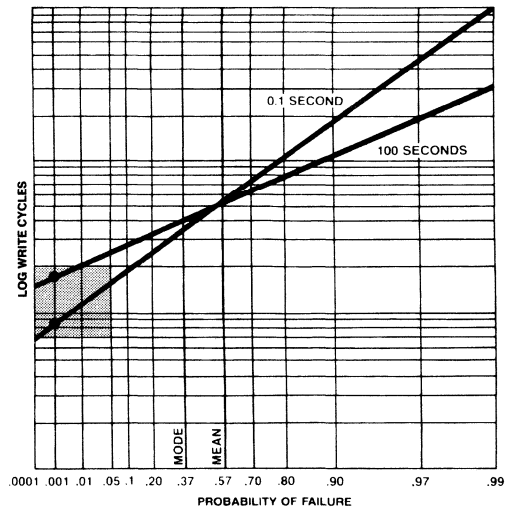


Figure 3: Affect of Write Cycle Frequency on Endurance

0018-3

## Conclusion

This paper has illustrated two methods for determining system reliability based on endurance. In the examples given, the failure rates due to endurance are well below industry standards for semiconductor failures.

Additionally, by factoring in the affects of both temperature and frequency of writing, the endurance failure rates for the X2816A system and X2864A system may be predicted specifically for the user's application.

DEVICE RANK	THOUSANDS OF WRITE CYCLES
1	297
2	315
3	355
4	365
5	400
6	410
7	450
8	450
9	510
10	572
11	620
12	620
13	650
14	680
15	800
16	820
17	940
18	952
19	992
20	1400

Table 2: Ranked Endurance Data for Twenty Pieces of X2816A Devices

0018-4

# RADIATION-INDUCED SOFT ERRORS AND FLOATING GATE MEMORIES

J. M. Caywood & Reliability Engineering Staff

## ABSTRACT

A new failure mechanism which may be induced in floating gate memories by ionizing radiation is discussed. This mechanism, which is designated a "firm error", is modeled in some detail. Calculations which show that the MTBF for alpha particles emitted by ceramic packaging materials is  $>100,000$  years are verified experimentally. The effect of device scaling on this mechanism is also discussed.

## INTRODUCTION

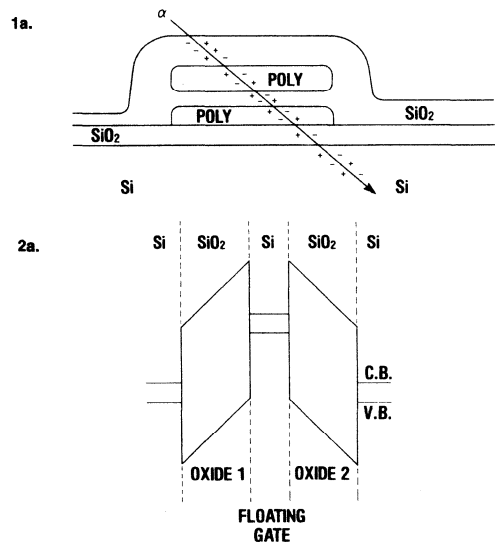
Ionizing radiation incident on floating gate non-volatile memories can give rise to three types of observable effects. The radiation may induce damage in the peripheral circuitry (hard errors); it may cause upset of the sense/readout circuitry (soft errors); or it may cause data loss by transfer of charge from the floating gate. The first of these groups of effects is common to all MOS circuitry and has been investigated extensively over many years.<sup>1</sup> The second group of effects was first observed in dynamic RAMs and has since also been observed in static RAMs and microprocessors.<sup>2-5</sup>

The third effect, on which this paper will concentrate, is qualitatively different than the "soft errors" which are observed in volatile RAMs. In the soft error case, thermalized carriers are collected from relatively long ( $\sim 10\mu\text{m}$ ) distances in the Si substrate which can result in efficient collection of the charges generated by an alpha particle ( $\sim 50\%$ )<sup>4</sup>. In the case to be discussed here, the carriers collected on the floating gate may come from two sources. One source is carriers created by the ionizing radiation in the  $\text{SiO}_2$  which lies between the floating gate and another electrode or the substrate when they are at a different potential. The second source is electrons excited in the floating gate which have enough kinetic energy to surmount the potential barrier between the conduction bands in Si and  $\text{SiO}_2$ . As will be developed in this paper, these effects are relatively inefficient ( $<1\%$ ). Unlike soft errors which are caused by a single ionizing particle, charge transfer to a floating gate is cumulative so that effects of many ionizing events occurring over an extended period of time must be considered.

To differentiate this phenomenon from soft errors which, if they occur in floating gate memories, are dependent upon the design of the readout circuitry and are temporary read errors which can be corrected by re-reading the floating gate, and from hard errors which render all or part of the memory inoperable, we shall call it "firm error". This firm error has the operational characteristics that it causes a read error which cannot be corrected by re-reading the floating gate, but it can be corrected by re-writing the cell or cells in question to provide a completely functional memory.

## MODELING THE CHARGE TRANSFER

Figure 1a shows a typical cross-section through a floating gate memory structure where the + and - signs indicate that electron-hole pairs are created along the track. Figure 1b shows a potential diagram of the same structure. Clearly electron-hole pairs created in the oxides on both sides of the floating gates will drift apart and tend to discharge the gate. Similarly electrons injected from the floating gate into either oxide will discharge the gate. The problem can therefore be broken into that of computing the charge created in the oxide and that of estimating the charge injected from the Si into the oxide.



0019-7  
Figure 1: Cross section and potential diagram of a typical floating gate memory transistor; a) the cross section is cut through in the direction of current flow; b) the potential diagram is shown for the case that the floating gate is programmed and the access gate grounded.

## INJECTION OF CHARGE FROM Si INTO SiO<sub>2</sub>

Emission of excited electrons from Si into SiO<sub>2</sub> is a complex process. Some of the phenomena occurring are illustrated schematically in Figure 2. Hot electrons created by the ionizing particle may be scattered by acoustic or optical phonons, other electrons, or the surface itself. The requirement for electrons to reach the surface with sufficient crystal momentum,  $\kappa$ , normal to the surface to surmount the barrier ( $\kappa_{\perp}^2/2m^* > \phi_B$  where  $\kappa_{\perp}$  is the component of  $\kappa$  normal to the surface,  $m^*$  is the effective mass, and  $\phi_B$  is the barrier height between the conduction bands in Si and SiO<sub>2</sub>).<sup>6</sup> Phonon scattering may be considered to be elastic since the phonon energies are small with respect to the barrier height. However, an electron scattering off another electron may lose up to one-half of its kinetic energy. Hence, electron-electron scattering rapidly thermalizes hot electrons.<sup>7</sup> The escape length of electrons is long for energies near the fermi level but drops rapidly and forms a broad U between 20 Å and 5 Å over the energy range 10 eV to 1000 eV.<sup>8</sup> Escape depths of 25 Å and 12 Å are reported for electrons 5.8 eV and 11 eV above the valence band maximum, respectively.<sup>9,10</sup>

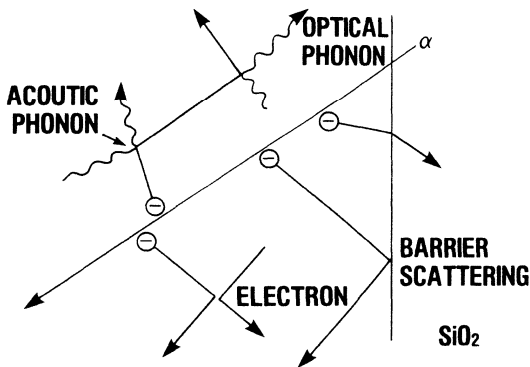


Figure 2: Schematic illustration of scattering process which contributes to small escape depth of electrons from Si.

The ideal situation would be to have electron yield curves as a function of energy for various charged particles of interest incident upon a biased oxidized silicon surface. Unfortunately, we lack such a complete data base, so we shall estimate the yields from data on optically stimulated emission. Figure 3 shows energy distribution curves (EDCs) for three photon energies plotted versus the energy of the states from which the electrons are excited for

photons incident on clean Si.<sup>11</sup> By integrating the EDCs and dividing by the incident photon energy, the yields in terms of electrons emitted per electron volt of incident photon energy are found to be  $6.7 \times 10^{-4}$ ,  $8.9 \times 10^{-4}$ , and  $8.7 \times 10^{-4}$  for photons with energies of 8.6 eV, 10.2 eV, and 11.8 eV, respectively. For lower energy photons, the yields drop precipitously.<sup>6</sup> It is known that the optical absorption length,  $1/\alpha$ , in Si is 80 Å for 12 eV photons.<sup>12</sup> Moreover, the electron escape depth at 11 eV is 12 Å.<sup>10</sup> This implies that one factor limiting the yield is that most of the electrons generated within the bulk of the Si relax via electron-electron scattering. Thus an estimate that a charged particle yields  $10^{-3}$  electrons for every electron-volt of energy lost within 80 Å of the surface is probably an upper bound for emission from silicon into a vacuum.

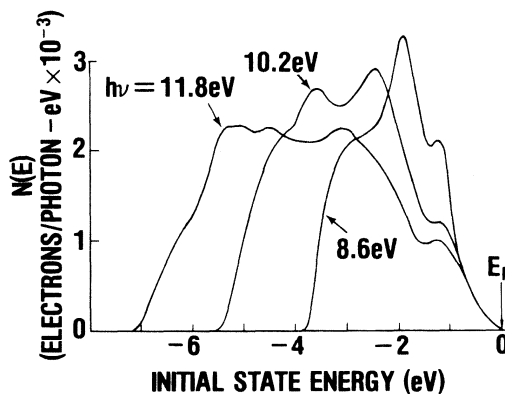


Figure 3: These energy distribution curves give electron yield vs. the energy of the initial state for photons incident on clean Si. (Data from Spicer, ref. 11).

Because the barrier between the conduction band in Si and the conduction band of SiO<sub>2</sub> is  $\sim 0.9$  eV lower than that between the conduction band of silicon and the vacuum level, the yield in the Si/SiO<sub>2</sub> system should be higher than that estimated above.<sup>6,13</sup> The magnitude of the yield increase can be estimated two ways. Callcott measured the effect of applying 0.16 monolayer of Cs to a Si surface. He found that the vacuum barrier was lowered by 1 eV and the photon yield was increased by 2.6 times.<sup>14</sup> Another estimate comes from the observation that for 6 eV photons, Powell reports  $\sim 13$  times higher quantum yield for the Si/SiO<sub>2</sub> system than does Broudy for the Si/vacuum system.<sup>6,13</sup> Since Powell applied a field of  $3 \times 10^6$  V/cm ( $\sim 5x$  that present in a typical floating gate memory), the barrier between Si and SiO<sub>2</sub> was lowered by 0.45 eV. This implies that

the ratio of the Powell and Broudy results is clearly an overestimate of the yield enhancement. Based on these data, we shall use 10x as a generous estimate of the magnitude of the yield increase between the Si/SiO<sub>2</sub> system and the Si/vacuum system. Our estimate of the yield of electrons emitted over the Si/SiO<sub>2</sub> barrier as a result of an incident ionizing particle is 10<sup>-2</sup> electrons for each eV of energy lost within 80 Å of the Si/SiO<sub>2</sub> interface.

## COLLECTION OF CHARGE GENERATED IN THE SiO<sub>2</sub>

The experimental evidence for collection of charge generated within SiO<sub>2</sub> is much more direct than for charge injected from the Si/SiO<sub>2</sub> interface. Measurements of Srour, Curtis, and Chiu show that the collection efficiency of electron-hole pairs generated by 4-5 keV electrons in SiO<sub>2</sub> varies from very low at low fields to ~20% at 5 x 10<sup>5</sup> V/cm to ~100% at 5 x 10<sup>6</sup> V/cm.<sup>15</sup> From calculations based on these measurements, Ausman and McLean have deduced that one electron pair is created for each 18 eV lost in the SiO<sub>2</sub>.<sup>16</sup> Since typical fields occurring in floating gate memory devices during read or storage operations are 5 x 10<sup>5</sup> V/cm, we shall assume that one pair is created for each 18 eV of energy lost in the oxide and that 20% of the charges created are collected at the electrodes.

## ENERGY DEPOSITED FROM IONIZING RADIATION

Ionizing radiation can be generally separated into that involving massless particles (X-ray, Gammas, etc.) and those which have mass (mesons, electrons, protons, atomic ions, etc.). The absorption cross-sections of the massless particles are quite small and decrease with increasing energy. For example, the  $\kappa_\alpha$  line of Mo occurring at 20.03 keV has a mass absorption coefficient of ~4cm<sup>2</sup>/g.<sup>17</sup> This means that approximately 1mm of Si is required to absorb 63% of the energy of a Mo X-ray beam. Since the cross-section is proportional to the cube of the wavelength, high energy photons lose even less energy per unit of length traveled through a solid. Because of this, it is expected that large fluences of X-rays would be required to transfer significant charge from the gate of floating gate memory.

For particles with mass, the stopping cross-section varies in a systematic way. This is illustrated in Figure 4 where we have plotted calculated energy loss rates in silicon for particles of differing mass using the Bethe-Bloch formalism.<sup>18</sup> As can be seen, for each mass particle, there is a peak in the curve of stopping power vs. energy which shifts to higher energy and becomes larger as the particle mass increases. Because of the log-log nature of the plot shown in Figure 4, it implies that there will be a high density of carriers created at the end of the particle track. This feature is called the Bragg peak.

Since the charge generation rate is maximum for particles with energies in the neighborhood of the Bragg peak, it is illuminating to calculate the charge transferred from a fairly conventional floating gate for two of the particles shown in Figure 4.

Alpha particles are known to be the chief cause of soft errors in volatile memories so their effect will be calculated. The other particle we will consider is an A1 ion, both for itself, since it may be generated as a result of muon capture by Si, and as a proxy for both the Si recoil ions which may be generated in various nuclear reactions and Mg which may also result from muon capture.<sup>19,20</sup>

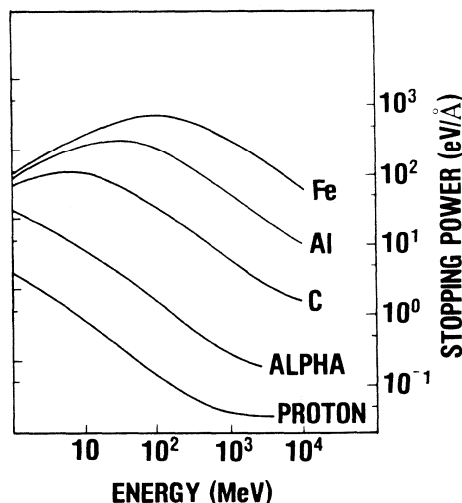


Figure 4: Energy loss rates vs. particle energy for particles with various masses calculated from Bethe-Bloch theory.

The Bragg peak for  $\alpha$ 's in Si occurs for particle energies in the neighborhood of 0.5 MeV. The energy loss rate for  $\alpha$ 's in Si is ~28 eV/Å in this range.<sup>21</sup> The energy loss rate for a compound such

as SiO<sub>2</sub> can be found from Bragg's rule which postulates the linear additivity of the energy loss cross-sections of the constituents of the compound, viz.

$$\epsilon(X_m Y_n) = m \epsilon(x) + n \epsilon(y)$$

Applying this to SiO<sub>2</sub> we find that the energy loss rate for alpha particles in SiO<sub>2</sub> near the Bragg peak is ~10.6 eV/Å.<sup>22</sup> Similar calculations for Al ions give approximate loss rates of 300 eV/Å and 110 eV/Å for Si and SiO<sub>2</sub>, respectively.

Putting all of this together in the context of Figure 1, we can see that the total charge collected per incident particle should be given by:

$$Q_p = \frac{N_{ox}(\epsilon)}{18} \int \frac{d_{ox1}}{\cos\theta} \left( \frac{dE}{dx} \right)_{SiO_2} dp$$

$$+ Y_{Si-SiO_2} \frac{\lambda_{esc}}{\cos\theta} \int \left[ \left( \frac{dE}{dx} \right)_{Si} dp + \left( \frac{dE}{dx} \right)_{Si} \right] dp$$

$$+ \frac{\eta_{ox}(\epsilon)}{18} \int \frac{d_{ox2}}{\cos\theta} \left( \frac{dE}{dx} \right)_{SiO_2} dp$$

where  $\eta_{ox}$  is the field dependent collection efficiency for pairs generated in the oxide,  $d_{ox1}$  and  $d_{ox2}$  are the thicknesses of the first and second oxides,  $\lambda_{esc}$  is the effect escape depth for electrons generated in the Si,  $\theta$  is the angle of the particle path to the normal,  $Y_{Si-SiO_2}$  is the yield (for normal incidence), and the integrals over path are needed because  $dE/dx$  is a function of energy and hence position.

## SAMPLE CALCULATION

As one example, let's calculate the probability of a floating gate device similar to those in current production being upset by alpha particles emanating from the packaging material. We will assume that the floating gate poly measures  $5\mu \times 14\mu \times 0.4\mu$ , that the transistor gate size is  $5\mu \times 5\mu$ , that the gate oxide and interpoly oxides are both 1000 Å thick and that the field oxide is  $1\mu\text{m}$  thick. We also assume that there is  $2\mu$  of SiO<sub>2</sub> deposited after the access gate is defined.

Figure 5 shows the alpha particle spectrum measured by Meieran et al.<sup>23</sup> The alpha spectrum is a result of the decay change of thorium and uranium which are present in the alumina which is used for hermetic packaging as trace impurities. For simplicity of calculation, we shall approximate this spectrum as two superimposed step functions. The high energy step begins at 8.6 MeV and the lower energy step at 7 MeV, the high and low energy steps have the relative weights of 3 to 7. Since it is known that the total emission rate of alumina ranges from 0.1 to

1.0  $\alpha/\text{cm}^2 \cdot \text{hr}$ , the integral over the approximation will be taken to be 1  $\alpha/\text{cm}^2 \cdot \text{hr}$ .

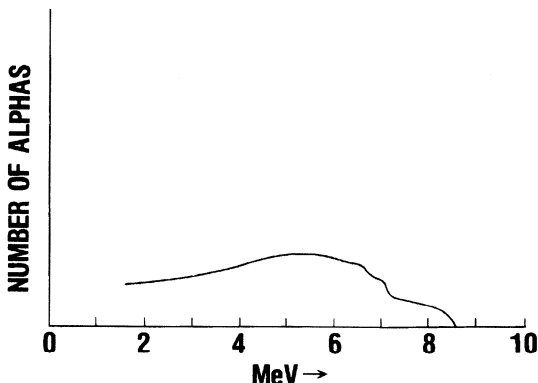


Figure 5: Spectrum of alpha particle emission rate vs. particle energy from an alumina lid. (Data from Meieran et al. ref. 23).

The maximum charge transfer which can occur as a result of a single particle is caused by a particle coming in at such an angle that the complete path length is within the gate oxide. (This requires that  $\theta > 88.85^\circ$ . However,  $\theta < 89.43^\circ$  because for larger angles, the path length of the overglass is so long that no particles get through. Moreover, at  $\theta = 89^\circ$ , the particle energy must be greater than 6.8 MeV to penetrate the glass.) If such a particle were to hit a cell so that  $5\mu$  of path length lay within the cell it could lose ~1.4 MeV. This implies a transfer of 15,550 electrons. The gate which is under consideration requires ~450,000 electrons to charge the state (assuming internal 2 V margin) or about 30 of these pathological alphas. Because the number of pathological alphas needed is  $>1$ , we can turn to a calculation of the average energy loss/particle.

We make the simplifying assumptions that the fraction of particles lost in the overglass from each of the two step functions contributing to the energy spectrum is given by the ratio of the path length in the overglass to the range of the highest energy particle in the step function, and that the energy loss rate in the effective charge collection region is that for 1 MeV. The first assumption causes an underestimation in the particles stopped in the overglass, and the second overestimates the energy contributed to charge generation. Under these assumptions the charge transferred from the floating gate by  $N_0$  alpha particles is given by:

$$Q_t = 2N_0 \sum_i r_i \sum_j l_j \left( \frac{dE}{dx} \right)_j C_j \int_0^{\theta_{max}} \frac{\sin\theta}{\cos\theta} [1 - \beta_i/\cos\theta] d\theta$$



where  $r_i$  are the relative contribution of the two components in the spectrum;  $\ell_j$  is the effective path length for charge generation;  $C_j$  is the conversion factor from energy loss to collected charges;  $\beta_j$  is the fraction lost in the overglass; and  $\theta_{\max}$  is taken to be the angle whose tangent is the gate length divided by the sum of the gate electrode and gate oxide thicknesses.

From this, one can find that the average alpha particle causes 580 electrons to be transferred from the floating gate. This means that about 750 alpha particles must hit the gate to change its state.

The problem becomes that of finding the probability that at least one cell has been hit 750 times, given that the average cell has been hit  $n$  times. Fortunately, the numbers are large enough that we can invoke the law of large numbers and approximate the distribution as normal with variance  $\sqrt{n}$ . If the array contains  $m$  cells then the probability that at least one cell is hit  $n_{\text{crit}}$  times is given by:

$$Q = \frac{m}{\sqrt{2\pi}} \int_z^{\infty} e^{-t^2/2} dt < \frac{m}{z} \sqrt{2\pi} e^{-z^2/2}$$

$$\text{when } z = (n_{\text{crit}} - n) / \sqrt{n}$$

as long as  $Q < 1$ .<sup>24</sup>

If  $n = 500$ , then  $Q < 1.84 \times 10^{-13}$  for a 16K chip and  $Q < 5.1 \times 10^{-12}$  for a 64K chip. For the chip size and alpha flux assumed, the expected period for the average alpha count per cell to reach 500 is  $7 \times 10^9$  hours. Given the approximations we have made, this probably understates the actual time by about an order of magnitude.

Turning briefly to carriers created by Al ions, we note that very few ions have energies in excess of 3 MeV.<sup>19</sup> Since this energy is below the Bragg peak for Al in Si, the ions stop fairly quickly. Nonetheless, the maximum energy loss rate is  $\sim 120$  eV/Å in SiO<sub>2</sub>. Since the maximum energy of the Al ions is  $\sim 3$  MeV, the maximum charge which would be collected from this ion is about 30,000 electrons which is still small enough that we can use normal statistics. Because of the small cross section for creation of these energetic ions, we can neglect this mode of charge generation for devices operating in normal terrestrial environments.

## SCALING

The effect of scaling on the firm error rate on floating gate devices is interesting because it is very different from that which occurs in volatile memories. If we assume that both lateral and vertical dimensions are scaled by a factor  $\lambda$ , then the storage capacitance decreases as  $\lambda$ . However, since the charge collection is dominated by generation in the oxide, it decreases like  $\lambda^3$ . If the voltage margin decreases like  $\lambda$ , the expected time for upset increases as  $\lambda$ , if the voltage margin is held constant, the expected time for upset increases like  $\lambda^2$ . Thus, scaling should decrease the firm error rate.

## EXPERIMENTAL RESULTS

To verify the theoretical results presented here, floating gate nonvolatile memories have been exposed to two types of radiation: gamma rays, representing massless particles, and alpha particles, representing massed particles. Table I gives the results. The devices tested contained a checkerboard pattern to look for firm error sensitivity for either bias of the floating gate.

As can be seen, no firm errors could be observed. The gamma radiation caused the devices to fail to meet the output leakage specification after 12,000 RAD. Measurement of the threshold of the output transistors showed that the thresholds had dropped from  $\sim 0.7V$  to  $\sim 0V$ .

The alpha particle fluence to which these devices were exposed was approximately that which would be seen after 200,000 years in a dirty package ( $1 \alpha/\text{cm}^2 \cdot \text{hr}$ ) or 2,000,000 years in a clean ( $0.1 \alpha/\text{cm}^2 \cdot \text{hr}$ ). These results are in good agreement with the predictions.

TABLE I

Radiation Type	Energy/quantum	Integrated Surface Flux	#Units Tested	#Firm Errors	Part Type
Gamma Radiation	58.6 keV	12,000 RAD	10	0	X2212
Alpha Radiation	5.3 MeV	$2.6 \times 10^9 \alpha/\text{cm}^2$	5	0	X2816

## SUMMARY

The question of "firm" errors in floating gate non-volatile memories has been treated. A firm error is defined as a change of data occurring as the result of transfer of charge from the floating gate by ionizing radiation. The rate of charge transport by various forms of ionizing radiation is discussed. The case of alpha particles is worked out in some detail as an example. Experimental results of exposure of units to gamma and alpha radiation are shown which support the theoretical predictions. The units in test survived exposure to 12,000 RADs and  $2.6 \times 10^9$   $\alpha/cm^2$  without firm errors. The alpha fluence is equivalent to that emitted by a typical ceramic package in about a million years.

## REFERENCES

1. e.g., Roger Freeman and Andrews Holmes-Siedle, IEEE Trans. Nucl. Sci. NS 25, 1216 (1978); J.M. Aitken, J. Electronic Mat. 9, 639 (1980).
2. T.C. May and M.H. Woods, Proc. 16th Annual International Reliability Physics Symp., 33 (1978).
3. D.S. Yaney, J.T. Nelson, & L.L. Vanskike, IEEE Trans. ED26, 10 (1979).
4. C.M. Hsieh, P.C. Murley & R.R. O'Brien, Proc. 19th Annual Reliability Physics Symp., 38 (1981).
5. R.P. Capece, Electronics 52, Mar. 15, p.85 (1979).
6. R.M. Broudy, Phys. Rev. B1, 3430 (1970).
7. For more sophisticated treatments of electron emission from solids cf. Leon Sutton, Phys. Rev. Lett. 24, 386 (1970); C.N. Bergland and W.E. Spicer, Phys. Rev. 136, A1030 (1964); Sven Tougaard and Peter Sigmund, Phys. Rev. B 25, 4452 (1982).
8. Lindau and W.E. Spicer, J. Electron Spectroscopy and Related Phenomena 3, 409 (1974).
9. G.W. Gobeli and F.G. Allen, Phys. Rev. 127, 141 (1962).
10. W.E. Spicer, J. Physique 34, C6 (1973).
11. W.E. Spicer, in "Optical Properties of Solids—New Developments", ed. B.O. Seraphin, p.658, North-Holland: Amsterdam (1976).
12. H.R. Phillips and H. Ehrenreich, Phys. Rev. 129, 1550 (1963).
13. R.J. Powell, J. Appl. Phys. 40, 5093 (1969).
14. T.A. Callcott, Phys. Rev. 161, 746 (1968).
15. J.R. Srour, O.L. Curtis, Jr., and K.Y. Chiu, IEEE Trans. on Nuclear Science NS-21, 73 (1974).
16. G.A. Ausman, Jr. and F.B. McLean, Appl. Phys. Lett. 26, 173 (1975).
17. Robert B. Leighton, "Principles of Modern Physics", pp. 421-425, McGraw-Hill, New York (1959).
18. Hans A. Bethe and Julius Ashkin, in "Experimental Nuclear Physics", ed. E. Segre, John Wiley, New York (1953).
19. J.F. Ziegler and L.A. Langford, Science 206, 776 (1979).
20. E.L. Petersen, IEEE Trans. on Nuclear Science NS 27, 1494 (1980).
21. W.K. Chu and D. Powers, Phys. Rev. 187, 479 (1969).
22. J.E.E. Baglin & J.F. Ziegler, J. Appl. Phys. 45, 1413 (1974).
23. E.S. Meieran, P.C. Engel, & T.C. May, Proc. 17th Annual Reliability Physics Symp., p.13 (1979).
24. Marvin Zelen and Norman C. Severo, in Handbook of Mathematical Functions, eds. Milton Abramowitz and Irene A. Stegun, p.926, National Bureau of Standards (1964).

# ENDURANCE MODEL FOR TEXTURED POLY FLOATING GATE MEMORIES

H.A. Richard Wegener

## ABSTRACT

Textured Poly Floating Gate (TPFG) memories are beginning to dominate the commercial market. This is due to many of its inherent strengths. One of these is the consistency of its endurance. Its predictability is here developed theoretically. Starting with a model of emission from bumps based on the radial solutions of LaPlace's and Poisson's equation in spherical coordinates and the use of an Extreme Value distribution for the bump radii, an expression for charge build-up at constant current fits experimental data very well. This charge build-up is proportional to fluence. When these results are used in a model for continuous data changes, an expression is developed that relates endurance exponentially to a ratio of internal voltages.

## INTRODUCTION

The basic features of the TPFG technology have been described in previous publications (1-4). The action of three polysilicon levels in charging and discharging the floating gate is shown in Figure 1.

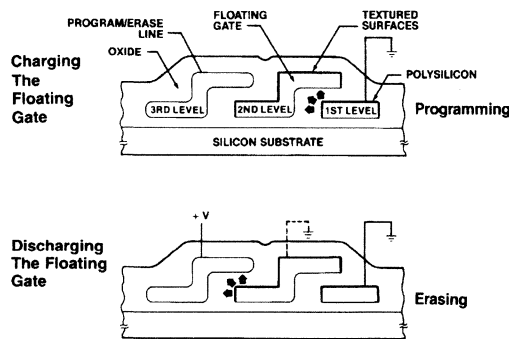


Figure 1: TPFG Cell Operation

Electron emission occurs only from a lower poly layer towards an upper poly layer. The oxide layers in between are in the 55 to 75 nm range, compared

to the 8 to 11 nm required for the other common floating gate technology. The reason is simple: the surfaces of the poly layers are textured to form many small bump-like features, whose curved surfaces enhance applied fields by factors of 4 to 5. The modeling of these fields is an important part of the analysis to follow.

## ENDURANCE

The term endurance has become accepted for a property common to all current nonvolatile memory technologies. It describes the number of data changes that a memory device can sustain without failure. In MNOS technologies, the failure is sometimes an inability to maintain the memory state for the required retention time; in thin oxide floating gate technologies it is often the breakdown of the fragile dielectric. In the TPFG technology, the end of endurance is generally caused by "trap-up", which prevents the transfer of charge to the floating gate. Trap-up is caused by the accumulation of trapped negative charge in the dielectric due to the repeated passage of current. These charges create a potential that opposes the potential necessary for tunneling. When this opposing potential reaches the voltage supplied on the chip, tunneling can no longer occur, resulting in the end of endurance. This paper describes a model for trapped charge build-up in TPFG devices.

## FIELD MODEL

Electron emission by Fowler-Nordheim tunneling requires the knowledge of the field at the surface of the bump. This model assumes a bump with a spherical tip, which permits the use of solutions of LaPlace's and Poisson's equations in spherical coordinates. It is further assumed that the emitting surface (cathode) is radially conformal with the collecting electrode (anode), so that only the radial parts of both equations need to be employed. This leads to a solution of the form

$$(1) E_c = -V_c/[R_c(1-R_c/R_a)] + (\sigma/K) R_d(1-R_d/R_a)/[R_c(1-R_c/R_a)]$$

where E is the field, R the radius, K the dielectric permittivity,  $\sigma$  a charge density per unit area, subscript c denotes a quantity at the cathode, and subscript a is a quantity at the anode. The first term describes the field in a dielectric free of charge, and the second has been cast in a form that the trapped charge distribution can be described by its charge density  $\sigma$  located at the centroid radius  $R_d$ .

## FORMALISM FOR TRAP GENERATION

There is a body of experimental data for parallel plate structures (5,6) that clearly indicates that the amount of trapped charge is proportional to the amount of charge that has passed through as current:

$$(2) Q_t = b \left\{ \int J dt \right\} (4 \pi R_c^2) (s/4)$$

where  $Q_t$  is the charge trapped, and  $\int J dt$  is the current density that passed through the dielectric integrated over time (termed "fluence"). The quantity  $b$  is the ratio of trapped charge to fluence. The second bracket converts charge density into charge, and  $(s/4)$  is the fraction of a full sphere that actually emits electrons. When this charge is concentrated at the centroid radius  $R_d$ , then

$$(3) Q_d = (\sigma) (4 \pi R_d^2) (s/4)$$

Equating  $Q_t$  with  $Q_d$ , solving for  $\sigma$ , substituting into eq (1), identifying the denominator of the second term of eq (1) as  $V_Q$ , and approximating  $R_d$  with  $R_a/2$  results in

$$(4) V_Q = \left\{ \int J dt \right\} (b/K) (R_c^2/R_a)$$

## FORMALISM FOR VARIATION OF BUMP SHAPES

All of the preceding derivations require two perfect concentric spherical shells to be applicable. To account for deviations from sphericity, and the distribution in the sizes of real bumps, as many as four constants might be necessary. But as a first approach it was decided to view the bumps as a distribution of perfectly spherical surfaces of limited area, with the hope that the dispersion parameter of the distribution of spherical radii would absorb the effects of contour variations. The distribution chosen was the Extreme Value distribution (7-9). Its sampling function has the form (10)

$$(5) R_{ci} = R_m - BB \{ \log [-\log (i - 0.5) / k] \}$$

where  $R_m$  is the radius at the maximum of the distribution (the mode),  $BB$  is the dispersion parameter,  $k$  is the number of samples chosen, and  $i$  is the rank number of the particular item of  $k$  samples chosen.

## CONSTANT CURRENT CHARACTERISTICS OF "TPFG" MEMORY TEST STRUCTURES

TPFG memory devices are operated by linear voltage ramps, which result in a forced constant current through the dielectric. A useful concept in this mode of operation is the "tunnel voltage"  $V_{TU}$ , which is the voltage that must be applied to sustain a specific constant current. For purposes of characterization, simple test structures are subjected to a set of forced constant currents, and the tunnel voltage  $V_{TU}$  is recorded vs fluence. Such a characteristic is shown in Figure 2.

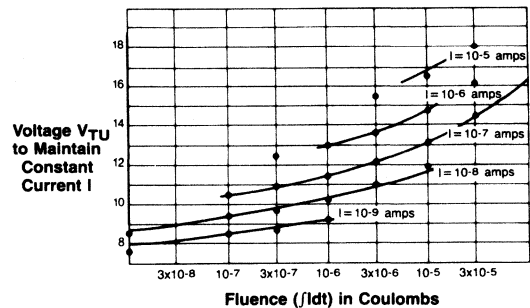


Figure 2: Tunnel Voltage vs. Fluence at Constant Current. Lines are experimental data, solid circles are calculated from eq (8).

With representative bump radii chosen by the sampling function the field at bump  $i$  is

$$(6) E_{ci} = [-V_{TU_i} + V_{Qi}] / [R_{ci} (1 - R_{ci}/R_{ai})], \text{ where}$$

$$(7) V_{Qi} = \{ \sum J_{FNI} \Delta t \} (b/K) (R_{ci}^2/R_{ai}).$$

Fluence is now expressed by its sum over time increments. The measured current is the sum of the currents from the number of all individual bumps  $G$ . The current density emitted by tunneling must be multiplied by the active spherical surface area. This leads to

$$(8) I = (G/k) \sum_{i=1}^k (4 \pi R_{ci}^2) (s/4) J_{FNI}, \text{ where}$$

$$(9) J_{FNI} = A E_{ci}^2 \exp -B/E_{ci}.$$

The initial modeling was done with a program in BASIC on a personal computer. The area of the structure was  $0.1\text{mm}^2$ , the number of bumps per square micrometer was 50, the oxide thickness was 59 nm, which translated into a value for  $R_{ai}=R_{ci} + 59$  nm. Following (11) the Fowler-Nordheim constants were set at  $A=6.5E-7$  amps -  $\text{cm}/V^2$  - sec and  $B=2.52E + 8V/\text{cm}$ . The dielectric permittivity was  $K=3.5E-13$ . The best fit was obtained for  $R_m=15.4$  nm,  $BB=4.8$  nm,  $b=2.0E-8$ , and  $s=0.03$ . The calculated values are shown as circles against the continuous experimental data on Figure 2. The value  $R_m$  is consistent with values obtained from T.E.M. cross-sections, the calculated dispersion has an analog in the estimated dispersion of bump base diameters, and  $b$  agrees very well with data presented at IEDM81 (6) for parallel plate structures. There is now a good basis for describing the processes occurring in TPGF memories. A pertinent example is shown in Figure 3. Here a constant current plot was calculated as a function of the number of samples representing the same distribution. While it is an indication that, indeed, 1024 samples are necessary to accurately depict conduction at fluences as low as  $1E-8$ , it also clearly shows that during the latter part of the life of the devices, all those different bumps can be represented by bumps of the same radius  $R_m$ . This should make the prediction of endurance somewhat less complex.

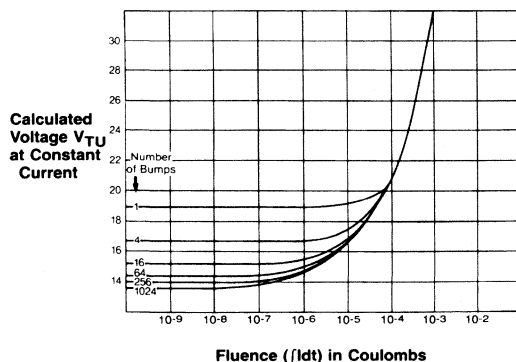


Figure 3: Effect of Number of Samples  $k$  on Calculated Tunnel Voltage

## VOLTAGE-TIME RELATIONSHIPS DURING PROGRAM-ERASE CYCLING

This analysis is based on the assertion that trap-up is the cause of the end of endurance. Since the build-up of traps is the result of current through the tunnel dielectric, this analysis is concerned only with the time interval during which tunneling occurs. As an aid to understanding, reference may be made to Figure 4.

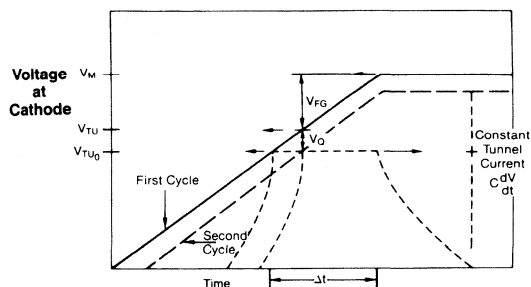


Figure 4: Voltage vs. Time Relationships at Floating Gate

The heavy line describes the (absolute) potential at the cathode (which may be poly 1 or poly 2) during the course of the first ramp to be applied to an untested structure. When the tunnel voltage  $V_{TU0}$  is reached, a current flows that remains constant until the maximum voltage (internal to the tunnel structure)  $V_M$ , is reached. The constant current is indicated by a superimposed plot in broken lines referenced to the right. When  $V_M$  is reached, the voltage stays constant for a "flat top" period. During this time, the current decreases exponentially, since any transferred charge reduces the tunnel potential. Since tunnel current flows during this first pulse, its fluence gives rise to trapped charge, which in turn causes an opposing voltage  $V_Q$ . Therefore, during the second pulse, the net potential on the cathode is reduced by  $V_Q$ . This can be indicated by a second ramp offset downwards by  $V_Q$ . The tunnel voltage for the same constant current is then reached later, and the time to reach the end of the ramp is shorter. As cycling proceeds, the time interval during which tunneling occurs becomes shorter and shorter. This simple picture neglects one important element of endurance cycling: each cycle of one polarity must be followed by a cycle of the opposite polarity. The charge stored during the previous cycle affects the

potential of the cathode during the following cycle. The amount of charge stored during each cycle can be picked off Figure 4 by looking at it in another way. Instead of offsetting all succeeding ramps, one may consider them all superimposed, and recognize that the tunnel voltage  $V_{TU}$  increases with each cycle. Then the tunnel voltage can be viewed as the sum of  $V_{TU0}$  and  $V_Q$ . Conversely, the charge transferred to the floating gate  $V_{FG}$  is the difference between  $V_M$  and  $V_{TU}$ .

## ENDURANCE MODEL

The change in  $V_{TU}$  per programming pulse on one bump is

$$(10) \quad dV_{TU}/dn = \Delta V_Q = \{J_{FN} \Delta t\} (b/K) (R_c^2/R_a)$$

where  $\Delta t$  is the total time during which current flows.

$$(11) \quad \Delta t = (V_{FGe} + V_{FTe} + V_{M_p} - V_{TU_p} + V_{FT_p})/r,$$

where  $r$  is the ramp rate  $dV/dt$ , subscript  $p$  refers to the programming step, and  $e$  to the erase step.  $V_{FGe} + V_{FTe}$  is the floating gate voltage left over from the erase step.  $V_{FT_p}$  is the charge added to  $V_{FG_p}$  during flat top. From previous analysis,  $V_{FGe} = V_{Me} - V_{TUE} + V_{FTe}$ . Let the structure be symmetrical so that all subscripts are interchangeable. Eq (11) can now be written

$$(12) \quad dV_{TU}/dn = \alpha(V_M - V_{TU} + V_{FT}) \text{ where}$$

$$(13) \quad \alpha = 2b J_{FN} R_c^2/K r R_a$$

Integrating (12), setting  $V_{TU} = V_{TU0}$  when  $n=0$ , setting  $V_M - V_{TU} + V_{FT} = V_{MS}$  when  $n = N$ , and rearranging, results in

$$(14) \quad N = (1/\alpha) [1n (V_M + V_{FT} - V_{TU0})/V_{MS}].$$

Here  $N$  is endurance expressed as the number of data changes before trap-up, and  $V_{MS}$  is the minimum voltage on the floating gate to be sensed as the correct state.

Near the end of endurance, according to Figure 3, after a fluence of about  $1E-4$  coulombs has been accumulated, the build-up of traps follows a path as if all bumps had the same radius  $R_m$ . This permits the exact substitution for  $R_c$  and  $R_a$  in Eq (13), and the calculation of  $V_{TU0}$  in Eq (14) with the help of Eq (9).  $V_{FT}$  can be calculated exactly, depending on flat top time and floating gate capacitance; it is of the order of 0.1-0.3 volts.  $V_M$  depends strictly on internal voltages and coupling ratios.  $V_{MS}$  depends on coupling ratios, the threshold voltage of the floating gate transistor, the minimum voltage required to accomplish sensing at the circuit sensing device. Memory cells operating within real circuits require

the establishment of both programming and erase voltage quantities to fit in Eq (14). Endurance distributions as a function of temperature have been recorded experimentally for specific TPGF products (12). Their modes are consistent with tunneling currents as determined from the measured ramp rates in circuits operating at different temperatures.

## CONCLUSION

There are three major results of this calculation. First, it indicates that textured surface emission can be modeled adequately by spherical geometrics, if modified by the dispersion of an Extreme Value distribution of the bump radii. Second, it confirms that TPGF memories are a part of the same universe as other silicon-to-silicon-dioxide tunneling structures, exhibiting the same mode of trapping (proportional to fluence), with a trapping ratio ( $b=2E-8$ ) that is essentially identical to that for parallel plate structures. Finally, on the basis of these results, a model for TPGF endurance based on charge build-up has been developed that appears well supported by experimental results.

## ACKNOWLEDGEMENTS

The author would like to thank Daniel Guterman for many clarifying discussions and important experimental data, David Scott for his work in obtaining endurance data, and Roberto Tam for his timely help in programming.

## REFERENCES

1. J. Drori, S. Jewell-Larsen, R. Klein, W. Owen, R. Simko, W. Tchou; "A Single 5-Volt Supply Nonvolatile Static RAM"; 1984 IEEE Internat. Solid State Circuits Conf. Technical Digest 24, pp 148-9 (1981).
2. S. Jewell-Larsen, I. Nojima, R. Simko; "A 5-Volt RAM-like Triple Polysilicon EEPROM"; Proc. 2nd Annual Phoenix Conf., pp 508-11 (1983). IEEE Catalog No. 83CH1864-8.
3. R.K. Ellis; "Fowler-Nordheim Emission from Non-Planar Surfaces"; IEEE Electron Device Letters, EDL-11, pp 330-2 (1982).
4. R.K. Ellis, H.A.R. Wegener, J.M. Caywood; "Electron Tunneling in Non-Planar Floating Gate Memory Structures"; IEEE IEDM82 Digest, pp 749-50 (1982).

- 
5. D.R. Wolters, J.F. Verwey; Springer Series in ElectroPhysics 7, p 111 (1981).
  6. M. Liang, C. Hu; "Electron Trapping in Very Thin Thermal Silicon Dioxides"; IEEE IEDM81 Digest, pp 396-9 (1981).
  7. B. Epstein, R. Brooks; "The Theory of Extreme Values and its Implications in the Study of the Dielectric Strength of Paper Capacitors"; J. Appl. Phys. 19, pp 544-50 (1948).
  8. P. Rosin, E. Rammler; "The Laws Governing the Fineness of Powdered Coal"; J. of the Fuel Inst. 7, p 29 (1933).
  9. E.J. Gumbel; "The Statistics of Extremes"; New York, NY, Columbia University Press, (1958).
  10. J.R. King; "Frugal Sampling Schemes"; Tamworth, NH, Technical and Engineering Aids for Management, (1980).
  11. J. Maserjian; "Tunneling in Thin MOS Structures"; J. Vac. Sci. Technol. 11, pp 996-1003 (1974).
  12. H.A.R. Wegener; "Endurance of Xicor E<sup>2</sup>PROMs and NOVRAMs"; Xicor Reliability Report RR504 (1984).

0020-5

---

## NOTES



# THE PREDICTION OF TEXTURED POLY FLOATING GATE MEMORY ENDURANCE

By H.A. Richard Wegener & Daniel C. Guterman

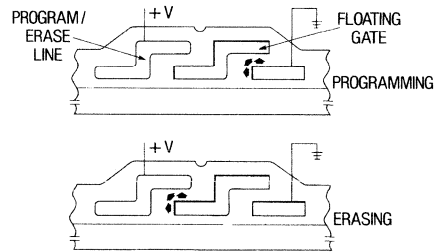
## BACKGROUND

The Textured Poly Floating Gate (TPFG) memory is one of the three major nonvolatile semiconductor memories currently in use. Details of its device theory and its use have appeared in previous publications.<sup>1-4</sup> Its nonvolatile memory cell employs three layers of polysilicon as shown in Figure 1. The most important feature of this cell is its ability to transfer electrons to and from the floating gate through oxide thicknesses of the order of 55 nm to 75 nm, in contrast to other nonvolatile memory technologies that must have dielectrics as thin as 10 nm surrounding their floating gate. The thick dielectric in the TPFG memory cell has proven its advantage in manufacturability and reliability. This advantage is made possible by the presence of a textured surface, whose curved features generate a field enhancement that permits Fowler-Nordheim emission at reasonable voltages. These features have the shape of bumps on the poly surface. The modeling of emission from these surfaces formed the major part of a recent paper.<sup>5</sup> Its results were that these bumps can be approximated by spherical caps on the tip of truncated cones, so that the fields can be found using Laplace's equation in spherical coordinates. From S.E.Ms and T.E.Ms these bumps were known to have a range of sizes. It was found that a simple two-parameter Extreme Value distribution of the cap radii was a sufficient description to get a good fit of model and experimental data over five orders of magnitude of constant current, and eight orders of magnitude of fluence.<sup>5</sup>

## ENDURANCE

Endurance is a characteristic common to all current nonvolatile semiconductor memory technologies. It describes the number of program-erase cycles that a memory device can sustain without

### FLOATING GATE STRUCTURE



0021-1

Figure 1: The nonvolatile part of a NOVDRAM\* cell is shown schematically with the permanently grounded poly 1 at right, the floating gate formed by poly 2 in the middle, and poly 3, also serving as the program/erase line, at the left. To program, poly 2 is coupled capacitively to a positive potential; this results in strong coupling of the floating gate to poly 3, and a high potential between poly 1 and 2. To erase, poly 2 is coupled capacitively to ground; this results in a high potential between the floating gate and poly 3.

failure. In other nonvolatile technologies, the failure modes may involve dielectric breakdown or loss of retention. In TPFG memories, failure is particularly graceful: The addressed bit cannot respond sufficiently to a data change. This is due to the fact that in this technology, the end of endurance is caused by trap-up. Trap-up is the result of the accumulation of trapped negative charge in the dielectric that is caused by the repeated passage of current. The endurance limit is reached when the potential due to this trapped charge grows so large that it suppresses the Fowler-Nordheim tunneling to the extent that insufficient charge is transferred to change the state of the floating gate. The modeling of endurance then simply involves the modeling of the build-up of the negative charge as a function of the number of pulses of Fowler-Nordheim current through the dielectric.

## DESCRIPTION OF ENDURANCE MODEL

A first step is the derivation of the voltage  $V_Q$ , which is the voltage due to the trapped charge that opposed the voltage necessary for tunneling  $V_{TU}$ . The spherical cap model permits the use of Poisson's equation in spherical coordinates. As shown in reference (5),  $V_Q$  is calculated for a charge density defined by a spherical shell with a centroid radius  $R_d$ . An educated guess approximates  $R_d$  with one half of the anode radius  $R_a$ . The

\*NOVDRAM is Xicor's nonvolatile static RAM device.

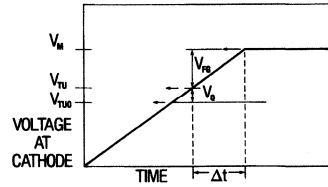
generation of charge density, following the results of previous workers<sup>6,7</sup> is made proportional to fluence (the time integral of current density  $\int Jdt$ ) by the trapping ratio  $b$ . This results in

$$V_Q = [\int Jdt] (b/K) (R_c^2/R_a) \quad (1)$$

where  $K$  is the dielectric permittivity, and  $R_c$  the radius of the (emitting) cathode surface.

Inspection of Figure 2 will help in understanding what happens during a single (erase) pulse. The ordinate shows the voltage on the program/erase electrode, the abscissa the time during a pulse. The voltage changes linearly with time as shown, at a ramp rate  $r = dV/dt$ . This ramp rate is proportional to the current put out by the charge pump on the chip. As the voltage between floating gate and program/erase electrode increases, a voltage  $V_{TU}$  is reached where Fowler-Nordheim tunneling is initiated. The tunneling current is exactly  $r \times C_{FG}$ , where  $C_{FG}$  is the capacitance of the floating gate. Since the pump current is constant,  $V_{TU}$  will be clamped at a value that keeps the tunnel current constant, but the voltage due to the charge transferred to the floating gate,  $V_{FG}$ , will rise until the ramp is limited at a maximum voltage  $V_M$ . At this point, the tunnel current will fall off rapidly, since any charge transferred will reduce the potential between floating gate and program/erase electrode. In the following analysis, the charge transferred after  $V_M$  is reached will be set to zero. The time,  $\Delta t$ , during which constant current flows through the dielectric is defined by the tunnel voltage  $V_{TU}$  at the beginning, and  $V_M$  at the end. During this time, electrons will be trapped in the dielectric, in proportion to the fluence  $J \times \Delta t$ .

The next pulse will therefore encounter an increased opposing potential  $\Delta V_Q$ , because of the trapped charge generated during the preceding pulse. The ramp voltage at which tunneling starts is now increased by this voltage, the net charge transferred to the floating gate is decreased, and the time  $\Delta t$  during which constant current flows is also decreased. During endurance cycling, the polarities of the pulses are alternated, so that an erase is followed by a program pulse. The (program) ramp following an erase pulse now encounters a potential due to charge transferred during the preceding pulse. This potential adds to that of the new ramp, so that the tunnel voltage is reached sooner, and constant current flows longer until  $V_M$  is reached. In fact, if the structure is symmetrical for both program and erase conditions, the time during which constant current flows is exactly twice that for a single ramp starting with zero charge on the floating gate.



0021-2

Figure 2: The voltage at the floating gate as a function of time is shown for one particular erase pulse. The voltage (due to displacement) changes linearly with time until the tunnel voltage  $V_{TU}$  is reached. Tunneling at constant current clamps the voltage at that value, resulting in a voltage  $\Delta V_{FG}$  due to charge transfer. The trapped charge due to previous erase cycles gives rise to an opposing potential  $V_Q$ .

## MATHEMATICAL MODEL OF SINGLE CELL ENDURANCE

For the purpose of analysis, the floating gate is considered a mosaic of pieces, each containing one emitting bump of cathode radius  $R_{ci}$ . All quantities with subscript  $i$  refer to one such representative piece. Setting the tunnel voltage at  $V_{TU0}$  when no charge exists in the dielectric:

$$V_M - V_{TU0i} = V_{Qi} + V_{FGi} \quad (2)$$

$$\Delta t_i = V_{FGi}/r = (V_M - V_{TU0i} - V_{Qi})/r \quad (3)$$

From Eq(1), the trapped charge in the dielectric after an erase and a program pulse is

$$\Delta Q_i = 2 (b/K) (R_{ci}^2/R_{ai}) J_{FNI} \Delta t_i \quad (4)$$

This can be expressed as the rate of charge trapping per program/erase cycle  $n$ :

$$dV_{Qi}/dn = \alpha_i (V_M - V_{TU0i} - V_{Qi}), \text{ where} \quad (5)$$

$$\alpha_i = 2 (b/K)(R_{ci}^2/R_{ai}) J_{FNI}/r \quad (6)$$

Integrating Eq(5), and setting  $V_{Qi}$  equal to zero at  $n = 0$ , results in

$$\ln [(V_M - V_{TU0i})/(V_M - V_{TU0i} - V_{Qi})] = \alpha_i n \quad (7)$$

Substituting Eq(2) into Eq(7) and solving for  $V_{FGi}$

$$V_{FGi} = (V_M - V_{TU0i}) \exp(-\alpha_i n) \quad (8)$$

The transition from the individual bump mosaic pieces to the full floating gate comes from the argument that the floating gate voltage is really the sum of the charge contributions  $Q_i$  from small amounts of current  $I_i$  emitted by all bumps, divided by the floating gate capacitance  $C_{FG}$ :

$$V_{FG} = \sum Q_i/C_{FG} = [\sum I_i \Delta t_i]/C_{FG} \quad (9)$$

$$I_i = 4\pi R_{ci}^2 (s/4) J_{FNI} \quad (10)$$

the Fowler-Nordheim  $J_{FNi}$  current is

$$J_{FNi} = A E_{ci}^2 \exp(-B/E_{ci}), \quad (11)$$

the field at the emitting bump is

$$E_{ci} = (-V_{TUi} + V_{Qi})/R_{ci}[1 - (R_{ci}/R_{ai})] \quad (12)$$

the cathode radius

$$R_{ci} = R_M - BB [\ln - \ln(i - 0.5)/G] \quad (13)$$

Summing all bumps  $i$  from 1 to the total number of bumps  $G$  results in the complete expression for the dependence of the floating gate voltage due to tunneled electrons  $V_{FG}$ , on the number of endurance cycles  $n$ :

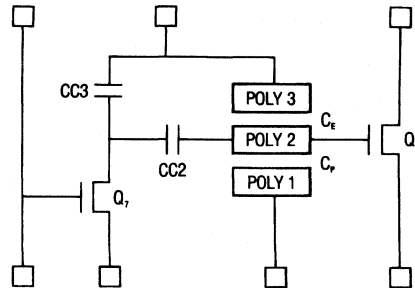
$$V_{FG} = (1/r C_{FG}) \sum 4\pi R_{ci}^2 (s/4) J_{FNi} \times (V_M - V_{TUOj}) \exp(-\alpha_i n) \quad (14)$$

The quantities after  $J_{FNi}$  are the result of replacing  $\Delta t_i$  in Eq(9) by Eqs(3) and (8). It now remains to define the end of endurance. Clearly, it arrives when the floating gate voltage is insufficient to establish the required logic level. The end of single cell endurance ( $n = N_c$ ) occurs when the floating gate voltage reaches a defined value ( $V_{FG} = V_{FGM}$ ) that is the boundary of that level.

## SINGLE CELL ENDURANCE DATA

The test pattern used to characterize endurance is the nonvolatile part of a Xicor NOVRAM cell shown in Figure 3. The dimensions of the test cell are identical to those in a NOVRAM memory array. The advantage of this cell is that all voltages can be applied directly to this cell. Cycling is achieved by applying a ramp between ground and  $V_M$ .  $V_{FG}$  is read out by applying the same control voltage sweep simultaneously to ground,  $V_M$  and P/E control. This couples to the floating gate and when a voltage equal and opposite to  $V_{FG}$  is reached, the (floating) gate on the sense transistor will indicate zero charge. Upon increasing the control voltage sufficiently the floating gate potential is increased by the threshold voltage of the transistor, turning on the sense line. This value of the control gate is then recorded, generating the plot shown in Figure 4. The ordinate shows the value of the control voltage necessary to turn on the sense transistor. Since  $V_{FG}$  is positive in the erase state, a negative control voltage must be applied. Therefore, the lower branch of the window plot represents the erase state. When  $V_{FG}$  approaches the threshold voltage of the transistor, its reaction becomes indeterminate, and the limit of the endurance of the cell is reached. ( $n = N_c$  when  $V_{FG} = V_T$ ). This situation is

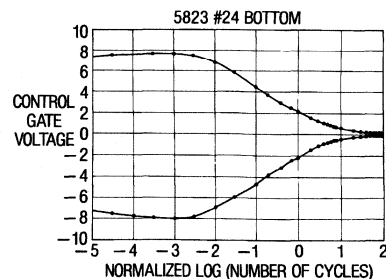
indicated when the applied control voltage is exactly zero. Inspection of Figure 4 shows that the end of the endurance for that particular cell occurred at a number of cycles normalized to a value of 100. The same factor of normalization was applied to all data quoted here in order to prevent possible confusion with results from individual products, or with published specifications.



0021-3

Figure 3: This shows the circuit schematic of the nonvolatile part of a NOVRAM cell. Two transistors are shown in addition to the elements in Figure 1. Transistor  $Q_7$  controls the access to the junction used for capacitive steering of write and erase operations, and transistor  $Q_8$  senses the voltage on the floating gate.  $V_{FG}$  can be measured by turning  $Q_7$  on hard, and finding the control voltage that must be supplied simultaneously to poly 1, poly 3, and capacitor  $CC_2$ , in order to cause a specified current to pass through  $Q_8$ .

## NOVRAM CELL ENDURANCE DATA



0021-4

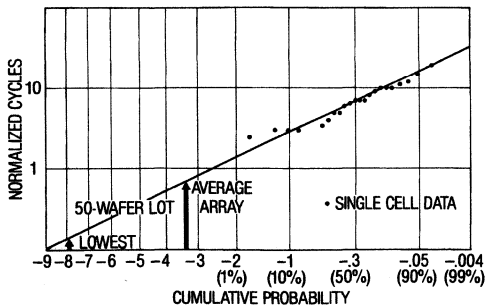
Figure 4: This is a plot of the charge transferred to the floating gate of a single NOVRAM cell as a function of the logarithm of the number of program/erase cycles. The actual floating gate voltage is the negative value of the control voltage minus the threshold voltage of  $Q_8$ .

## RELATIONSHIP OF SINGLE CELL DATA TO LOT ENDURANCE

The number of program-erase cycles at a control voltage of zero was determined for a number of single cell structures from the same wafer lot. The results were plotted on log normal probability paper.

The results can be seen on Figure 5. Careful reading of the abscissa will establish its relationship with the usual chart. In effect, the scale has been extended on the low probability side of the distribution, and for simplicity of notation, the cumulative probabilities have been marked as their base ten logarithms. In a few selected locations near the right hand side, the equivalent percentage values were given in brackets. The single cell data points are on either side of the 50% line of the chart. The slope of the best fit straight line defines the dispersion of the distribution.

**RELATIONSHIP OF SINGLE CELL DATA TO LOT ENDURANCE**



0021-5

Figure 5: This shows the Log Normal probability plot of individual single cell endurance data. The right half of the plot is quite standard, as marked by typical cumulative percentages. The left half represents an extension of the standard chart to much lower probabilities, in order to permit predictions for specific members of a much larger population.

In order to relate these results to the endurance of a commercial lot of NOVRAMs, the definition of the endurance of an integrated circuit with an array of memory cells should be recalled. This definition states that the limit of the endurance of a chip is reached when the first cell fails, after having sustained the same number of data changes as every other cell on that chip. If that chip has 1024 memory cells, then the cell with the lowest endurance limit of these 1024 cells defines the endurance of that chip. The cumulative probability for this is  $1/1024$ . Any chip with 1024 cells can be expected to have that endurance. The number of cycles at the cumulative probability of  $1/1024$  therefore represents the average endurance of a chip from a given lot. The lowest endurance on a wafer of chips is caused by the cell with the lowest endurance on that wafer. If there are, say, 850 chips per wafer, then the cumulative probability of this endurance limit is  $1/(1024 \times 850)$ . Looking now at a full 50 wafer lot, the lowest endurance of that lot has a cumulative probability of  $1/(1024 \times 850 \times 50)$ . The plotting of ranked data on probability paper requires "plotting posi-

tions" that result in about half the calculated cumulative probability values<sup>8</sup> for the lowest value used. In order to be consistent with the plotted data points, the cumulative probability for the average chip endurance from the 50 wafer lot is 0.0005, and this is indicated by an arrow of Figure 5. Similarly, the lowest possible chip endurance on that wafer lot is  $1E-8$ .

## COMPARISON OF SINGLE CELL PROJECTION WITH COMMERCIAL LOT DATA

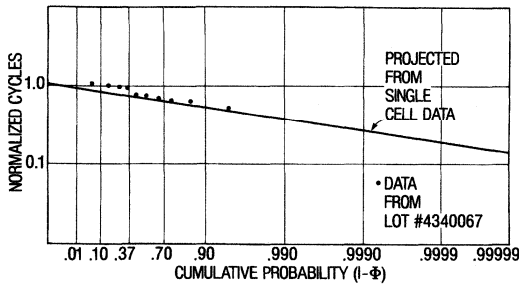
The endurance of individual arrays from a commercial lot can be described by a statistical distribution and its parameters. Since the endurance of an array is determined by the lowest endurance of a fixed number of cells, an Extreme Value distribution describes the distribution of the lowest endurances of all the arrays, and therefore, of the arrays within a lot.<sup>9</sup> This applies regardless of the distribution of the endurances of individual cells within the same array. It is an empirical fact that it is the logarithm of the number of cycles that has the Extreme Value distribution,<sup>10</sup> very similar to the Log Normal distribution frequently found for data from electronic devices. Lot data can be handled simply by the use of Extreme Value probability paper. Available charts are designed for maximum extreme values. For minimum extreme values, such as the lowest endurance of an array, these charts can be used by substituting the complement for the cumulative probability of an observation in order to determine the plotting position. Instead of  $\phi$ ,  $(1 - \phi)$  is used to determine the abscissa. Figure 6 is based on these considerations.

The abscissa is labeled by the complement values, which results in the reversal of the slopes of the straight line describing the distribution. The ordinate is (just as Figure 4) in terms of the logarithm of the normalized endurance. Since the distribution is described by a straight line in this coordinate system, it requires only two points to define its locus. These two points were determined in the previous section: the endurance of the average array, and the minimum endurance of the lot. The difference from Figure 5 (aside from the distribution function) is that the definitions of the cumulative probability values have changed. In terms of an individual cell, the cumulative probability of the endurance of an array is related to  $1/1024$ ; in terms of the array, the cumulative probability is the expected average of individual array units. For the (maximum) Extreme Value distribution this is 0.57; since the shape of the

distribution has not changed, the use of the complement does not apply and the value of the (log of) endurance on Figure 5 at the larger arrow is entered on Figure 6 at  $\phi = 0.57$ . Similarly, the minimum endurance of an array from a 50 wafer lot is now associated with a cumulative probability of  $0.5/(50 \times 850)$  a value increased by a factor of 1024 over the corresponding single cell value (see preceding section). The cumulative probability for the minimum (array) endurance of a lot is therefore  $1.2E-5$ , to be plotted at the 0.99999 position. A straight line drawn through this point and the array average establishes the projected distribution of array endurances. This graphical technique of deriving lot endurances from single cell data will be supplemented by an equivalent mathematical approach in the Appendix.

How good is the fit to actual data? Endurances from a typical monitor of that general time slot in NOVRAM production are shown on Figure 6. The fit is not fortuitous: there are dozens of lot data with almost identical slopes over a range of roughly a factor of 0.5 to 2. Confidence limits (95%) from the single cell data permit a scatter twice as large.

**ENDURANCE FROM SINGLE CELL VS. COMMERCIAL LOT DATA**



0021-6

Figure 6: This is a Log Extreme Value probability plot of the endurance of a lot of X2212 NOVRAMs. The points are measured values, the straight line represents endurances predicted from the single cell data shown in Figure 5.

**CONSTANT CURRENT TESTING**

The determination of endurance is a very time consuming process. In single cell data taking, typically tens to hundreds of millions of cycles are required. This routinely takes on the order of days to accomplish. For product endurance prediction, about twenty cells are needed, requiring simultaneous testing for any semblance of monitoring effi-

ciency. A much more rapid method of evaluation has been in use for some time. It depends on the observation of the time necessary to reach some predetermined tunnel voltage, when a constant current is forced through the test structure. An empirical factor correlates observed time with observed product endurance. Test times are on the order of ten to ten thousand seconds, depending on conditions used. Inspection of Eq(8) explains the reason for this. The time  $\Delta t$  during which constant current flows is proportional to  $V_{FG}$  (Eq(3)). It is therefore exponentially decreasing with the number of write-erase cycles. Since the data ramp takes the same amount of time, whether current flows through the dielectric or not, the time consumed increases linearly with the number of cycles, while the limiting process decreases exponentially. A constant current test adds the periods of current flow without pauses, reaching the condition for the trap-up limit of endurance in a minimum of time.

**MATHEMATICAL RELATIONSHIP BETWEEN ENDURANCE AND CONSTANT CURRENT DATA**

The work described in reference (5) proved that the constant current data can be modeled by bumps whose size have the proper distribution. Since this requires the addition of the contributions of thousands of bumps, the number of different bump radii necessary for a good fit was studied. It was found that at low fluences, a large number was necessary, but after a sufficient amount of charge has passed through the dielectric, the contributions from different bumps had nearly equalized, so that only a few bump radii were a sufficient description. After high fluences, a single bump, representative of the maximum of the distribution of radii, could predict the tunnel voltage necessary to maintain a constant forced current. Since the end of endurance is brought about by high tunnel voltages after large fluences, this condition applies very well and is used in the following analysis. When, in Eq(14),  $R_{ci}$  is replaced by  $R_M$ , the summation sign is replaced by a multiplication by  $G$ . Then the factor to the left of, and including,  $J_{FNi}$  becomes  $1/(r \times C_{FG})$ . But  $I = r \times C_{FG}$ , so that, when  $R_{ci}$  becomes  $R_M$ ,

$$N_C = (1/\alpha_M) \ln[(V_M - V_{TUOM})/V_{FGM}] \tag{15}$$



Substituting  $r \times \Delta t$  (see Eq(3)) for the voltage term in parentheses in Eq(5), multiplying by  $dn$  and integrating results in

$$\int dV_{Qi} = \alpha_i r \int \Delta t_i dn \quad (16)$$

The integral of  $\Delta t$  with respect to the number of cycles is, of course the total time of constant current flow through the dielectric. At the endurance limit,  $V_{Qfi} = V_M - V_{TUOi} - V_{FGMi}$ , and the integral of time intervals is equal to the total time of constant current flow to the instant of the end of endurance,  $t_{Ni}$ . Again invoking the asymptotic limit of all  $R_{Ci}$ 's becoming  $R_M$ ,

$$t_N = (V_M - V_{TUOM} - V_{FGM})/r \alpha_M \quad (17)$$

Solving Eq(17) for  $\alpha_M$  and substituting in Eq(15) results in the expression for endurance as calculated from constant current data

$$N_C = [r t_N / (V_M - V_{TUOM} - V_{FGM})] \times \ln[(V_M - V_{TUOM}) / V_{FGM}] \quad (18)$$

Conversely, the elapsed time at constant current  $t_N$  equivalent to endurance  $N_C$  is obtained by interchanging those two quantities in Eq(18). An estimate of the time advantage is obtained by realizing that in cycling, a minimum time of  $2 \times V_M/r$  is consumed per cycle. Since typically, some time, both analog and digital, is spent in the transition from programming to erasing, this minimum time is doubled.

Therefore the elapsed time to reach the end of endurance by cycling  $t_{CC}$ , is closer to

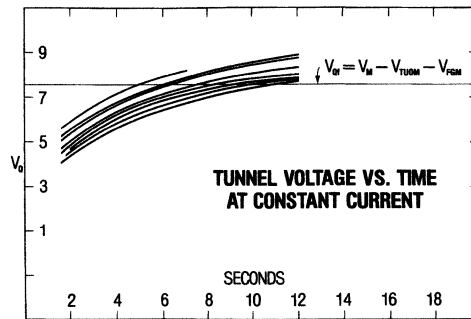
$$t_{CC} = 4 N_C V_M/r \quad (19)$$

Substituting pertinent values, one can find that  $t_N$  is approximately  $t_{CC}/50$ .

## EXPERIMENTAL CORRELATION OF CONSTANT CURRENT WITH CYCLING DATA

Textured poly capacitor test patterns from the same wafers that had been used to obtain the single cell cycling data displayed in Figure 5 were subjected to forced constant current conditions, and their tunnel voltages were recorded as a function of time. An automated test system exists to perform this test on a routine basis. When tunnel voltage was plotted vs time, the data for ten such structures

resulted in Figure 7. According to Eq(17), when  $V_{Qf} = V_{TU} - V_{TUO} = V_M - V_{TUO} - V_{FGM}$ , then the end of endurance is reached. This condition is indicated by the horizontal line at that voltage. The time  $t_N$  to reach that can be read off the graph and converted into equivalent cycles by Eq(18). These endurances can then be plotted on a graph similar to that used in Figure 6.

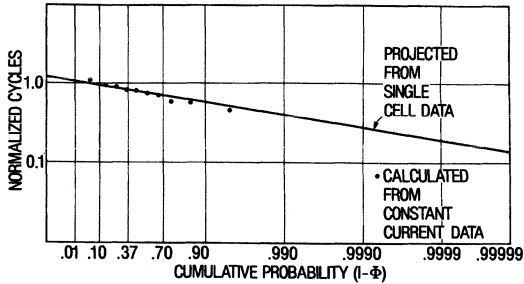


0021-7

Figure 7: This is a record of tunnel voltage (expressed as trap-up voltage) vs time. The end of endurance is reached when the tunnel voltage reaches a value  $V_{Qf}$ . The time associated with that voltage can be read off this chart.

The area of the constant current structure was eight hundred times that of the single cell capacitors. Since its behavior is dominated by the highest current features, it is set equal to the endurance of the 400th lowest cell. This has been chosen as the average endurance of the lot of constant current devices. The fit in Figure 8 indicates good correlation between the two methods of determining endurance. This means that product endurances can be legitimately predicted from constant current data. Test times on the order of ten seconds are short enough for the E-test stage of wafer evaluation: they clearly permit the prediction of product endurance. But as increasing knowledge leads to an improvement in endurance, this time is expected to increase by several orders of magnitude. Eq(17) indicates a predictable acceleration technique. All that is needed is to increase the level of constant current, measure time to reach the voltage of the endurance limit, and insert that value onto Eq(17). In addition, the value of  $r$  must be adjusted to reflect the new current value, according to  $r = I/C_{FG}$ . Finally, a secondary adjustment must be made to the value of  $V_{TUOM}$  by calculation. Another method would be to increase the area of the constant current device to bring more low endurance features into play.

## ENDURANCE FROM SINGLE CELL VS. CONSTANT CURRENT DATA



0021-8

Figure 8: This is again a Log Extreme Value probability plot. The points are those calculated from the times measured via Figure 7. The straight line represents the endurance predicted from the single cell data in Figure 5.

## SUMMARY

We have described a coherent body of understanding and data that permits the prediction of product endurance, and the use of devices for accelerated testing, from first principle device models. This fortunate circumstance arises from the advantageous technological feature of textured poly tunneling, namely that there is one, and only one, mechanism that is prevalent in determining the end of endurance.

This one mechanism is trap-up, the build-up of negative charge in the dielectric in proportion to the fluence of the tunnel current. The model for window closure and for single cell endurance flows naturally from this concept. The predictability of accelerated tests is also the result of this single unifying mechanism. The relationship with product endurance follows from basic statistical considerations.

## ACKNOWLEDGMENTS

The authors would like to express their appreciation for the general support given to this work by Xicor management and staff. In particular, thanks are due to Yupin K. Fong and Kurt B. Raab for their effective help in the software development and for the performance of the measurements of the individual test structures.

## APPENDIX

### Mathematical Formulation for Lot Endurance from Single Cell Data

The approach taken here is simply to translate the graphical operations performed in preceding sections into symbols. Underlying its simplicity are the operations leading to the design of probability papers. They begin by translating the cumulative distribution of a variable into a linear function of that variable. The single cell endurences have the form:

$$\begin{aligned} \phi_C &= 1/2 + (1/2) \{1 - \exp [\text{BELOW}]\} & (A1) \\ \text{BELOW} &= [-(\pi/2) (\ln N_C - \ln \bar{N}_C)^2 / \sigma^2] \end{aligned}$$

where  $\phi_C$  is the cumulative probability of single cell endurance  $N_C$ ,  $\bar{N}_C$  is the average cell endurance, and  $\sigma$  its standard deviation. The function form chosen is an approximation<sup>11</sup> to the normal distribution function. It is chosen here because it could be inverted most simply into a form linear in  $N_C$ , since the intent is to make the operations more transparent to the reader. The same operations could be performed by using the exact integral formulation of the cumulative probability of the normal distribution. Expressing Eq(A1) as a linear function of  $\ln N_C$

$$\ln N_C = \ln \bar{N}_C - \sigma \times F_C, \text{ where} \quad (A2)$$

$$F_C = \{(-\pi/2) \ln [\phi_C (1 - \phi_C)]\}^{1/2} \quad (A3)$$

Eq(A2) relates any single cell endurance  $N_C$  to its probability factor  $F_C$  and via Eq(A3), to its cumulative probability  $\phi_C$ . The lowest endurance  $N_{CA}$  expected from an array of cells is defined by

$$\begin{aligned} \ln N_{CA} &= \ln \bar{N}_C - \sigma \times F_{CA}, \text{ where} & (A4) \\ \phi_{CA} &= [1/(\# \text{ cells/array})] \end{aligned}$$

An equation like Eq(A4) can be set up for the minimum endurance of a wafer lot  $N_{CM}$ , where  $\phi_{CM} = [1/(\# \text{ cells/wafer lot})]$ . For the lot endurences, an equivalent scheme is set up:

$$\ln N_A = \ln \bar{N}_A - (1/\alpha) \times F_A, \text{ where} \quad (A5)$$

$$F_A = \ln [-\ln (1 - \phi_A)] \quad (A6)$$

Now  $N_A$  is the endurance of an array (or chip),  $\bar{N}_A$  is the modal endurance of the lot, and  $F_A$  is the probability factor derived from the Extreme Value distribution. Incidentally,  $F_A$  is exact and not an

approximation. In analogy to Eq(A4), the average array endurance  $\bar{N}_{AA}$  has the form

$$\ln \bar{N}_{AA} = \ln \bar{N}_A - (1/\alpha) \times F_{AA} \quad (A7)$$

The value of  $\phi_{AA}$  for the average of the distribution must be 0.43, in order that its complement becomes 0.57, the locus of the average of the (maximum) Extreme Value distribution. The minimum endurance of the lot has the same subscript as Eq(A7), except that subscript AM is substituted for AA. The probability factor  $F_{AM}$  is based on  $\phi_{AM} = [1/(\# \text{ arrays/wafer lot})]$ . It will be realized that  $N_{CA} = N_{AA}$ , and  $N_{CM} = N_{AM}$ . Therefore two simultaneous equations can be solved for  $\bar{N}_A$  (the lot average), and  $1/\alpha$  (the lot dispersion), in terms of single cell parameters:

$$1/\alpha = \sigma \times [(F_{CM} - F_{CA})/(F_{AM} - F_{AA})], \quad (A8)$$

and

$$\ln \bar{N}_A = \ln \bar{N}_C - \sigma \times [(F_{CA} \times F_{AM} - F_{AA} \times F_{CM})/(F_{AM} - F_{AA})] \quad (A9)$$

Expressing Eq(A5) in terms of single cell parameters results in

$$\ln N_A = \ln \bar{N}_C - \sigma \times \{ [F_{CA}(F_{AM} - F_A) - F_{CA}(F_{AA} - F_A)] / (F_{AM} - F_{AA}) \} \quad (A10)$$

In this way, the individual endurances expected from a commercial lot  $N_A$  can be predicted from the size of the lot tested, which determines  $F_A$ , the single cell constants  $\bar{N}_C$  and  $\sigma$ , and chip size details of that product, which convert the F's with double subscripts into specific constants.

## REFERENCES

1. J. Drori, S. Jewell-Larsen, R. Klein, W. Owen, R. Simko, W. Tchon; "A Single 5-Volt Supply Non-Volatile Static RAM"; 1981: IEEE Intn'l Solid State Circuits Conf. Technical Digest 24, pp. 148-9 (1981).
2. S. Jewell-Larsen, I. Nojima, R. Simko; "A 5-Volt RAM-like Triple Polysilicon EEPROM"; Proc. 2nd Annual Phoenix Conf., pp. 508-11 (1983). IEEE Catalog No. 83CH1864-8.
3. R.K. Ellis; "Fowler-Nordheim Emission from Non-Planar Surfaces"; IEEE Electron Device Letters, EDL-11, pp. 330-2 (1982).
4. R.K. Ellis, H.A.R. Wegener, J.M. Caywood; "Electron Tunneling in Non-Planar Floating Gate Memory Structures"; IEEE IEDM82 Digest, pp. 749-50 (1982).
5. H.A.R. Wegener; "Endurance Model for Textured Poly Floating Gate Memories"; IEEE IEDM84 Digest, pp. 480-83 (1984).
6. D.R. Wolters, J.F. Verwey; "Springer Series in ElectroPhysics 7"; p. 111 (1981).
7. M. Liang, C. Hu; "Electron Trapping in Very Thin Thermal Silicon Dioxides"; IEEE IEDM81 Digest, pp. 396-9 (1981).
8. J.R. King; "Frugal Sampling Schemes"; Tamworth, NH, Technical and Engineering Aids for Management, (1980).
9. H.A.R. Wegener; "Endurance of Xicor E<sup>2</sup>PROMs and NOVRAMs"; Xicor Reliability Report RR504 (1984).
10. E.J. Gumbel; "The Statistics of Extremes"; New York, NY Columbia University Press, (1958).
11. Eds. Milton Abramowitz & Irene A. Stegun; "Handbook of Mathematical Functions"; Natl. Bureau Standards, Applied Mathematics Series-55, p. 933 (1964).



## COMPARISON AND TRENDS IN TODAY'S DOMINANT E<sup>2</sup> TECHNOLOGIES

By S.K. Lai & V.K. Dham—  
Intel Corporation  
Daniel C. Guterman—  
Xicor, Inc.

### ABSTRACT

This paper reviews the three dominant E<sup>2</sup> technologies today, namely the two floating gate approaches of thin tunnel oxide and oxide on textured poly and the dual dielectric approach of MNOS. It evaluates each approach with respect to cell design, operation, manufacturability, compatibility with established process technologies and reliability. It follows with a comparison of the technologies in the areas of development entry cost, scaling and reliability. After a review of the market place, this paper concludes with a projection of the requirements of E<sup>2</sup> technologies to support full function, commodity E<sup>2</sup> memories (E<sup>2</sup>PROM) as well as low cost micro-controllers and ASIC (Application Specific Integrated Circuits).

### INTRODUCTION

Electrically alterable nonvolatile semiconductor memory has been an area of active research for many years, with the promise that it will be the ultimate silicon memory. The first floating gate memory was proposed in 1967<sup>1</sup> and MNOS memories were reported at about the same time.<sup>2</sup> In 1980, the first 16K E<sup>2</sup>PROMs using MNOS<sup>3</sup> as well as floating gate technologies on FLOTOX<sup>4</sup> were reported, while textured poly E<sup>2</sup>PROMs were reported in 1983.<sup>5</sup> However, after all these years of development in the laboratory and volume manufacturing, E<sup>2</sup>PROMs have yet to become a high volume, widely used memory component compared to EPROMs, the closest equivalent memory with lower functionality. There are many reasons given for the limited growth, ranging from the higher cost of E<sup>2</sup>PROM based products to poorly understood reliability of

these components. In this paper, we will focus on the technology factors by comparing the three dominant E<sup>2</sup> technologies to date, and giving our own viewpoint on the development in the market place.

### DESCRIPTION OF TECHNOLOGIES

#### FLOTOX (FLOating gate Tunnel OXide)

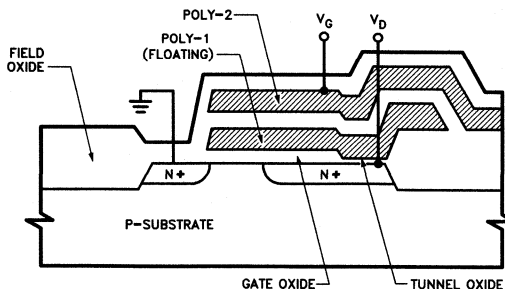
The cross sectional structure of a FLOTOX cell is shown in Figure 1a. It consists of a floating gate transistor with a thin oxide grown over the drain region. The floating gate is surrounded completely by high quality silicon dioxide, giving its superior retention characteristics. Programming (electrons into floating gate) is achieved by taking the control gate to high voltage while erase (electrons out of floating gate) is achieved by grounding the control gate and taking the drain to high voltage. Because the program and erase coupling conditions are different, they have different design considerations. Electron transfer is through Fowler-Nordheim tunneling mechanism using electric field higher than 10 MV/cm. The IV slope of tunneling is so steep that there is insignificant tunneling under normal read conditions for more than ten years. In order for the cell to properly operate in an array, it has to be isolated by a select transistor. Two cycles are required to load the correct data. All cells in a byte are first programmed, and then selected cells are erased using the drain for data control. The manufacturing process for FLOTOX is an extension of the EPROM technology, which in turn is an extension of the standard single poly silicon gate technology. The critical step in the process is the growth of high quality thin (<12 nm) tunnel oxide. For reliability, the dominant failure mechanism for FLOTOX is the breakdown of the tunnel oxide due to defects under the high field stress of the program/erase cycles, resulting in a leaky oxide.<sup>6</sup>

#### Textured Poly Cell

The cross sectional structure of a textured poly cell is shown in Figure 1b. It consists of 3 layers of poly with overlap forming three transistors in series. The floating gate transistor is in the middle formed by poly 2. Again, the floating gate is surrounded by silicon dioxide for high retention. Programming is

© 1986 IEEE. Reprinted, with permission, from INTERNATIONAL ELECTRON DEVICE MEETING, IEDM, Los Angeles, CA, December 7-10, 1986.

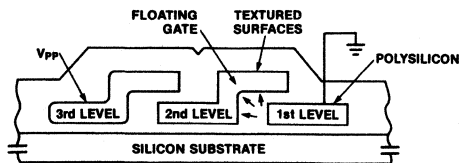
## FLOTOX DEVICE STRUCTURE



0022-1

Figure 1a: Cross sectional structure of a FLOTOX memory cell.

achieved by electrons tunneling from poly 1 to poly 2 and erase is achieved by electrons tunneling from poly 2 to poly 3. The program and erase coupling again is different. The poly 3 is taken to high voltage in both cases, and the element which tunnels is determined by the voltage applied from the drain and coupled to the floating gate through the channel region. The final data state is determined by the data state on the drain: this is a "direct write" cell with no need to clear before write as is required in the FLOTOX cell. This is possible because there are two active tunnel elements. The tunneling process is fundamentally still Fowler-Nordheim tunneling, with enhancement of local electric field due to the geometrical effect of fine texture at the poly surface. The electric field enhancement factor is in the range of 3 to 5, allowing much thicker oxides (60 nm to 100 nm) to be used. No extra transistor is required in an array since the poly 3 transistor serves the function of select transistor, giving a much more compact cell layout. The manufacturing process for textured poly is again an extension of the EPROM process with the addition of an extra layer of poly. The critical process step in this process is the growth of the tunnel oxide on poly. Because thicker oxides are used, oxide breakdown is less of a problem compared to FLOTOX. The dominant failure mechanism in a textured poly cell is electron trapping which results in memory window closure.<sup>7</sup>



0022-2

Figure 1b: Cross sectional structure of a textured poly memory cell.

## MNOS (Metal Nitride Oxide Silicon) Cell

The cross sectional structure of a MNOS cell is shown in Figure 1c. It consists of a single transistor with a dielectric stack of silicon nitride on top of a thin layer of oxide (1.5 nm to 2.0 nm) on silicon. Typically, the transistor resides in a well so that the channel potential can be controlled. Unlike the floating gate, charge is stored in discrete traps in the bulk of nitride. Because of the discrete nature of traps, charge transfer has to occur over the large area of the channel region. This is different from floating gate devices where charge transfer can occur over a small area removed from the channel region. On the other hand, any dielectric defect fatal to floating gates will only discharge local traps in MNOS. Programming is achieved by applying high voltage to the top gate whereas erase can be achieved by grounding the top gate and taking the well to high voltage. The program and erase coupling is symmetrical. Because of the very thin oxide, charge is being leaked off continuously due to the internal field, giving an ever diminishing window. In an array, select transistor is required to operate the cell properly. The select transistor may be separate<sup>3</sup> or integrated<sup>8</sup> in which case a more compact cell layout can be realized. Two cycles are again required to load the correct data. Furthermore, the well potential has to be controlled during data change, which makes the array operation more complex. The manufacturing process for MNOS is an extension of single poly silicon gate technology. The memory transistor is fabricated after the first poly periphery transistors are formed to maintain the integrity of the dual dielectric storage element. The

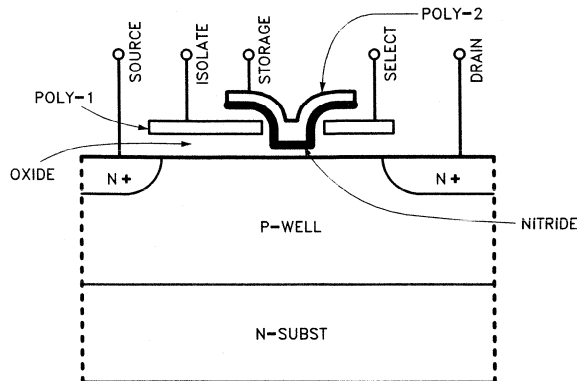


Figure 1c: Cross sectional structure of a MNOS memory cell.<sup>8</sup>

0022-3

important steps include thin oxide growth, nitride deposition and post nitride temperature cycles. The biggest reliability concern is cell retention and its degradation with cycling.<sup>9</sup>

## COMPARISON

The three different approaches have their technical merit and difficulties. Any one of these technologies can be made to work if they are given sufficient effort and focus. As a result, other considerations ranging from “comfort factors” to compatibility with available technologies tend to determine the choice.

## Development Entry Cost

Entry cost is the amount of extra effort required to bring up a new technology. To an EPROM manufacturer, it is relatively easy to take the FLOTOX approach. The cell concept is simple and the tunnel oxide process is a straight forward variation of a standard high quality oxide furnace cycle. This is why the majority of companies have opted for this approach for their E<sup>2</sup> effort. The textured poly approach, on the other hand, depends on a tunneling process which is not generally understood and is believed to require tighter process control. The cell concept is more complex and the use of three layers of poly imply higher wafer cost. These factors have limited the popularity of developing this approach. Finally, MNOS approach requires the mastering of a number of difficult process steps. The growth and control of the ultra thin oxide, as well as the quality of nitride are critical issues. As a result, despite gaining initial momentum, MNOS has not achieved dominance as an E<sup>2</sup> technology.

## Scaling

There are many factors that determine the size of a memory cell, and generally cell design represents finding the optimum compromise of a number of tradeoffs. Furthermore, as these technologies approach fundamental physical or practical material limits, scaling will become increasingly difficult. For FLOTOX, there is large area requirement for layout of the two transistors plus the tunnel oxide area, dictated by minimum design rules. The select transistor is limited by high voltage. Given the high oxide capacitance of thin tunnel oxide, large poly to poly area is required for the sense transistor. Scaling of the tunnel dielectric is also limited by direct tunneling at 6 nm and yield and reliability issues at 8 nm to 10 nm. Typically, relatively high voltages (15V to 20V) are required to operate the cell. As a result, FLOTOX cell does not scale well.

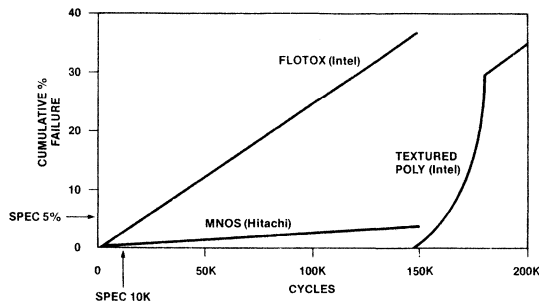
In the case of textured poly, the three poly layers are integrated resulting in a compact layout. Cell size is limited more by lithographic registration of poly layers than by ability to resolve space between poly lines as is the case with FLOTOX. Furthermore, the thick tunnel oxide requires smaller coupling capacitor area to give the required coupling. Given the same performance and reliability requirement, it is estimated that a textured poly cell is about a factor of two smaller compared to a FLOTOX cell for a given generation of technology. Textured poly does require higher operating voltage (>20V) and thus needs a high voltage technology to support it. Finally, scaling of the poly oxide involves more than thinning down the oxide as the field enhancement factor changes with oxide thickness.

The basic MNOS memory cell can be very small and highly scaleable. The select transistors, wheth-

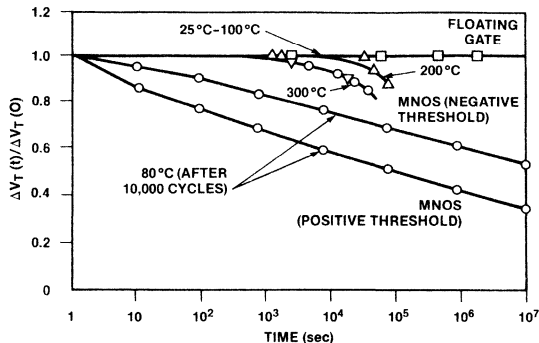
er separated<sup>3</sup> or integrated,<sup>8</sup> will limit scaling. However, in either case, the cell size is better than FLOTOX, and competitive with triple poly for a given generation of technology. One major problem is the requirement of well voltage control. Full byte function is only possible with separate well, giving a large effective cell size. Page function<sup>8</sup> can be used to partially circumvent the well problem but limits endurance. For oxide thicknesses, there is little or no room to scale the ultra thin tunnel oxide, so most of the emphasis has been on scaling the nitride. Charge leakage from the scaled nitride to top gate has been solved by oxidizing the nitride to give a MONOS stack. Low program and erase voltages have been demonstrated at the expense of smaller operating window.

## Reliability

One general problem for E<sup>2</sup>PROM is the limited information on the reliability of the technologies due to sample size or correlation problems. For floating gate technologies, there is no intrinsic problem with data retention, and because the technologies are designed to handle high voltage, there is very low failure rate due to normal 5V operation. Reliability problems occur during program and erase cycles in part because very high voltages are used. For FLOTOX, there is random single bit failure due to oxide defect resulting in a leaky oxide that loses charge over time (see Figure 2). For textured poly, the average electric field across the tunnel oxide is 3 to 5 times lower compared to FLOTOX. As a result, oxide breakdown failure is reduced significantly. On the other hand, there are more electron traps in the oxide, and the impact of electron trapping is magnified by the 3 to 5 times field enhancement factor. Consequently, electron trapping is the dominant failure mechanism, showing up as a failure to program or erase. The failure can be projected real time with margining techniques and since trapping is an intrinsic property, failure probability can be easily projected. In MNOS, charge retention is the dominant reliability issue (see Figure 3). The charge loss process is time dependent, resulting in continuous loss of cell margin and performance. The degradation based on short term data is difficult to predict. The ultra thin oxide is stressed by electric field comparable to FLOTOX and retention is further degraded with program and erase cycles. So far, wide variation in retention and endurance are being reported based on limited sampling.<sup>9</sup>



0022-4  
Figure 2: Endurance of 3 E<sup>2</sup> Technologies: FLOTOX and textured poly processed at Intel (16K arrays), MNOS data from Hitachi (prorated to 16K).



0022-5  
Figure 3: Data Retention: Floating gate, no intrinsic charge retention problem; MNOS, continuous charge loss and window closure tending to become worse after cycling.

## THE MARKET PLACE

Though E<sup>2</sup>PROMs have been available for the last five years, their usage has not grown to the volumes projected. A host of new and established companies have become active in the field, but lack of technology and product feature standardization, together with high cost and reliability concerns have limited the growth in the market place. The major issues for 16K have been 5V only, address/data latch vs no latch, ready/busy vs data polling, 24 pin vs 28 pin, 1 ms vs 10 ms program, self timed vs user timed, with and without V<sub>CC</sub> lockout and 10K vs 1 Million cycles endurance. Byte vs page function and page size are issues at 64K density level. In addition, one can choose oxynitride vs oxide for FLOTOX, textured poly vs FLOTOX for floating gate, and MNOS vs floating gate for E<sup>2</sup>. The reliability claims are difficult to understand and verify due to the link of failure to endurance cycling. Different

---

methods are used in reliability evaluation, and no standard exists to allow a meaningful comparison. For example, high temperature cycling is worse case for FLOTOX but may be best case for textured poly. Nevertheless, there has been continued growth in the E<sup>2</sup>PROM market, sustained by a wide, diversified application base. The driving force is end-user, in-the-field customization capability offered to microprocessor based products, which is either unavailable, unreliable or not cost effective using other techniques. As a result, standards are now established following 5V-only RAM-like functionality, and the cost and density gap to competing solutions continues to close.

## FUTURE TRENDS

There are two major driving forces in the development of E<sup>2</sup> technologies for the future. One of them is high density memories, requiring small memory cell size for the lowest cost per bit. The second requirement is low density nonvolatile memories in microcontrollers and programmable logic type applications. In the latter case the absolute cell size is not as important as process simplicity and low cost of the overall technology. MNOS based E<sup>2</sup> memories will continue to be used in low density memory as well as military applications requiring high radiation tolerance. However, it has only enjoyed limited popularity for use in high density memory and the trend will continue. A majority of companies have opted for FLOTOX as their first E<sup>2</sup> technology because of the simple device physics and the low entry cost for development. Recently, many Japanese companies have announced 64K E<sup>2</sup>PROMs based on FLOTOX for the smart card market. A number of companies have applied FLOTOX in ASIC and programmable logic array applications. In fact, some have developed single poly versions of FLOTOX for synergy with random logic technology. However, for stand alone high density E<sup>2</sup> memories, FLOTOX will be increasingly limited by defect oxide breakdown problems,<sup>10</sup> giving unacceptable failure rate above the 64K level, unless thicker oxides or new dielectrics can be used in new approaches. Error correction codes can also be used but at the expense of additional die cost.<sup>11</sup> Finally, textured poly inherently gives a smaller memory cell and suffers least from the oxide breakdown problem. Electron trapping is an intrinsic property that can be predicted and easily screened. Consequently, textured poly technology is expected to be most reliable and cost effective for 256K and above densities, while the higher cost of a three layer poly process may limit its use in logic applications.

The nonvolatile memory technology is an ever evolving field. Memories<sup>12,13,14</sup> based on hybrid operation of programming by EPROM and erase by tunneling have gained interest. The erase function is generally limited to the full array and thus it is called FLASH erase. Recent approaches offer cell size and technology complexity comparable to EPROMs, and the functionality of electrical erase. If such technologies are proven to be reliable and manufacturable, they will fill the need of a special market segment and become another major force in the developing nonvolatile memory market.

## SUMMARY

We have reviewed the three dominant E<sup>2</sup> technologies today. MNOS is used in low density memories as well as military applications, but enjoyed only limited popularity for high density memories. FLOTOX has been the most popular approach because of its simplicity and is most suited for low density memories and programmable logic type application. Textured poly gives the smallest memory cell size and is the most cost effective and reliable approach for high density memories.

## REFERENCES

1. D. Kahng and S.M. Sze, "A Floating Gate and Its Application to Memory Devices", *Bell Syst. Tech. J.*, 46, 1283 (1967).
2. H.A.R. Wegener et al., "The Variable Threshold Transistor, a New Electrically Alterable Nondestructive Read-Only Storage Device", presented at the IEEE Electron Devices Meeting, Washington, D.C., 1967.
3. T. Hagiwara et al., "A 16 Kbit Electrically Erasable PROM Using n-Channel Si-Gate MNOS Technology", *IEEE J. of Solid State Circuits*, SC-15, 346 (1980).
4. W.S. Johnson et al., "A 16 Kbit Electrically Erasable Nonvolatile Memory", *ISSCC Tech. Digest*, p. 152 (1980).
5. S. Jewell-Larsen et al., "A 5 Volt RAM-like Triple Poly Silicon EEPROM", *Proc. 2nd Annual Phoenix Conf.*, p. 508 (1983).
6. R.E. Shiner et al., "Characterization and Screening of SiO<sub>2</sub> Defects in EEPROM Structures", *21st Annual Proc. Reliability Physics*, p. 248 (1983).

- 
7. H.A.R. Wegener, "Endurance Model for Textured Poly Floating Gate Memories", IEDM Tech. Digest, p. 480 (1984).
  8. A. Lancaster et al., "A 5V-Only EEPROM with Internal Program/Erase Control", ISSCC Tech. Digest, p. 164 (1983).
  9. W.D. Brown, "MNOS Technology—Will it Survive?", Solid State Tech., p. 77 (July 1979).
  10. A. Bagles, "Characteristics and Reliability of 100Å Oxides", 21st Annual Proc. Reliability Physics, p. 152 (1983).
  11. S. Mehrotra et al., "A 64 Kb CMOS EEPROM with On-Chip ECC", ISSCC Tech. Digest, p. 142 (1984).
  12. D. Guterman et al., "Electrically Alterable Hot-Electron Injection Floating Gate MOS Memory Cell with Series Enhancement Transistor", IEDM Tech. Digest, p. 340 (1978).
  13. F. Masuoka et al., "A New Flash E<sup>2</sup>PROM Cell Using Triple Polysilicon Technology", IEDM Tech. Digest, p. 464 (1984).
  14. S. Mukherjee et al., "A Single Transistor EEPROM Cell and its Implementation in a 512K CMOS EEPROM", IEDM Tech. Digest, p. 616 (1985).

# NEW ULTRA-HIGH DENSITY TEXTURED POLY-Si FLOATING GATE E<sup>2</sup>PROM CELL

By D. Guterman, B. Houck, L. Starnes and B. Yeh

This paper describes a new, highly scaled cell structure, the smallest full function E<sup>2</sup>PROM cell reported to date. It utilizes the textured triple-poly-si technology, exploiting the high degrees of structural and functional integration, to achieve a cell size of 31  $\mu^2$ . A top view of the cell, built with 1.2 micron rules is shown in Figure 1, with cell cross-section and equivalent circuit shown in Figures 2 and 3, respectively.

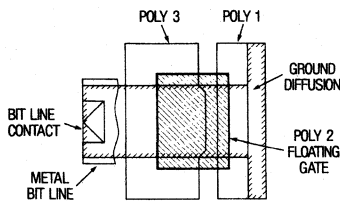


Figure 1: Cell top view.

0023-1

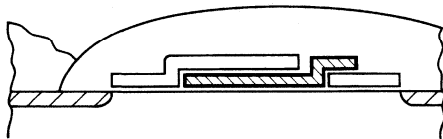


Figure 2: Cell cross-section.

0023-2

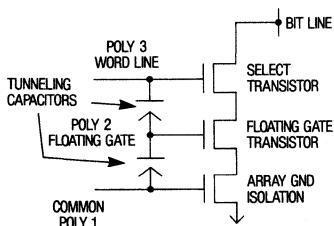


Figure 3: Cell equivalent circuit.

0023-3

Very small memory cell size is achieved by exploiting the vertical integration of the three poly layers to form a merged gate single transistor cell. This cell is made possible through the dual functions incorporated within various key components; specifically, (1) the poly 3 element, which functions as both word line select transistor and erase tunneling anode (2) the poly 1 electrode which serves the dual role of cell ground isolation transistor and programming cathode during write operation, and (3) the poly 2 floating gate transistor whose channel region establishes both the floating gate charge-conditional current path for reading and the input-data-conditional steering capacitor for writing. Charge transport to and from the floating gate is through Fowler-Nordheim tunneling, established by the geometrically enhanced fields at the textured poly interfaces between poly-si layers. This allows tunneling injection and transport to occur across oxides of thickness greater than 500Å at voltages less than 15V. In comparison to ultrathin (100Å) E<sup>2</sup>PROM technologies, the thicker interpoly oxides result in lower parasitic capacitance of the tunneling element, improved dielectric reliability because of the 3-5 $\times$  lower average fields in the oxide, and an easier path to oxide scaling.

Because of the simultaneous incorporation of the poly 2 to 1 programming and poly 3 to 2 erase tunneling elements, data storage is a direct, single pass operation, involving the following sequence (see Table I). First the poly 1 line, common to the entire array, is brought low, cutting off the conduction path from bit line through the cell to array ground. Next, the bit lines are set up to either 0V for an erased state or about 16V for a programmed state. Finally, the poly 3 word line is ramped up to about 22V in 1 ms to drive the nonvolatile charge transport. To erase, the bit line is grounded, whereupon the channel under poly 2 capacitively steers the floating gate towards ground. This induces sufficient voltage across the poly 3/2 tunneling element to remove electrons from the floating gate. When the bit line is high for programming, the channel potential steers the floating gate positively. This

TABLE I: OPERATING CONDITIONS

Operation	Bit Line	Poly 3	Poly 1
Standby	2V	0	5V
Read	2V	5V	5V
Write			
Erased State	0	$\sim$ 22V	Low
Programmed State	$\sim$ 16V		

© 1986 IEEE. Reprinted, with permission, from INTERNATIONAL ELECTRON DEVICE MEETING, IEDM, Los Angeles, CA, December 7-10, 1986.

induces sufficient voltage across the poly 2/1 tunneling element to inject electrons onto the floating gate.

Following up on the present 256K product experience, a number of fundamental factors are incorporated into the technology to maintain a high degree of reliability with scaling. Dielectric integrity and excellent charge retentivity is preserved through the use of thick, high quality thermal SiO<sub>2</sub> dielectrics, throughout. Direct write cell operation provides shorter write time by eliminating the unconditional clear before write. As in previous floating gate E<sup>2</sup>PROMs, 5V-only capability via on-chip voltage multiplication is possible because of the efficient Fowler-Nordheim tunneling mechanism.

Small test arrays of the 31 μ<sup>2</sup> cell, shown in the SEM views of Figure 4, have been built and operated successfully for endurance of 1 million writes. Figure 5 shows a representative extended endurance plot, demonstrating erased state cell currents of greater than 40 μA and programmed cells having thresholds of greater than 5V, thereby remaining in cutoff.

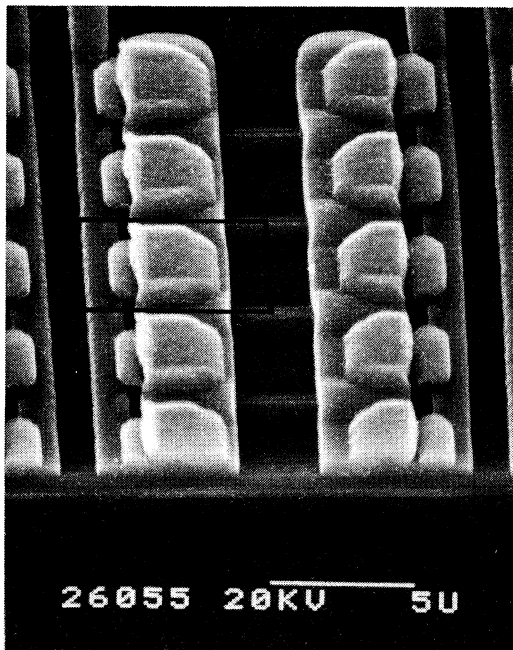


Figure 4a: Cell SEM top view.

0023-4

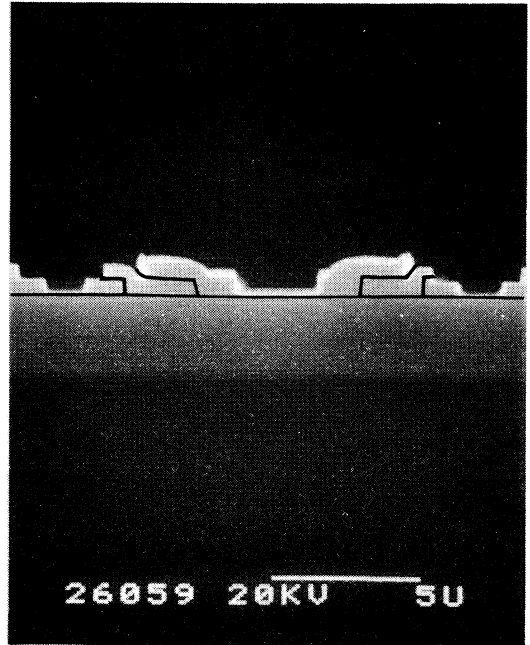


Figure 4b: Cell SEM cross-section.

0023-5

**ENDURANCE DATA**  
**LOT # BD230001S/04 X130/1**

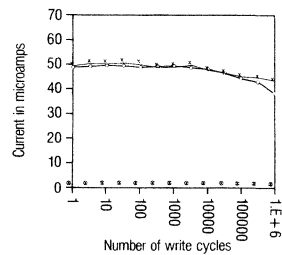


Figure 5: E<sup>2</sup>PROM cell test endurance data.

0023-6

In conclusion, this paper reports the smallest full function E<sup>2</sup>PROM cell described to date. Small size is a result of a cell in which elements serve multiple functions and a technology which is conducive to scaling. This approach will serve as foundation for developing future generation E<sup>2</sup>PROMs beyond today's 256K density.



# RELIABILITY COMPARISON OF FLOTOX AND TEXTURED POLY E<sup>2</sup>PROMs

By Neal Mielke—Intel Corporation  
Lori J. Purvis & H.A. Richard Wegener—  
Xicor, Inc.

## SUMMARY

FLOTOX and Textured Poly E<sup>2</sup>PROMs share the excellent retention and lifetest performance of the more common EPROM. In particular, retention failures add only about 20 FIT to lifetest failure rates in the 100 FIT range. The lifetest failure rates compare favorably with those of simple static logic products, because these high voltage devices have no oxide breakdown problems during 5V operation. FLOTOX endurance is limited entirely by oxide breakdown, overwhelmingly of the tunnel oxide. Window closing, caused by electron trapping, occurs but does not cause failure in well-designed products.

The Textured Poly approach offers a reliability tradeoff: less oxide breakdown but more window closing. This tradeoff becomes favorable at higher densities. This is because oxide breakdown, being a defect mechanism, worsens with increasing memory size and with scaling of oxide thickness. Window closing is an intrinsic mechanism that does not worsen dramatically with higher density. The two failure mechanisms—oxide breakdown and window closing—should be treated separately in reliability evaluations because they have different dependencies on cycling, temperature and retention bakes.

## RETENTION CHARACTERISTICS

The E<sup>2</sup>PROM retention is at least as good as the EPROM retention, as shown in Table I. The 0.2% failing for the I 2817A represents only 20 FIT added to the failure rate. All retention failures are at most only a few bits out of the memory array. Intrinsic retention limitations simply do not exist on these technologies; most bits have essentially unlimited retention.

Excellent retention is expected with these technologies for two reasons:

- 1) The stored charge on the floating gate is contained by the 3.2eV energy barrier which exists at the Si-SiO<sub>2</sub> interface. This barrier height is quite high, comparable to the barriers preventing dopant atoms from redistributing.
- 2) The oxide layers, even with FLOTOX, are thick enough to prevent carriers from tunneling off the floating gate during low voltage operation.

## LIFETEST PERFORMANCE

TABLE II: LIFETEST COMPARISONS OF INTEL E<sup>2</sup>PROM, EPROM AND STATIC LOGIC

Product(s)	Technology	125°C Lifetest Predicted Failure Rate (55°C, in FIT)		
		Breakdown	Retention	Total
2817A	FLOTOX	0	36	70
27256	EPROM	0	22	63
2114B, 8088, etc.	HMOS-II	110	0	120

The failure rates predicted from lifetest in Table II compare favorably with those of EPROMs, which in

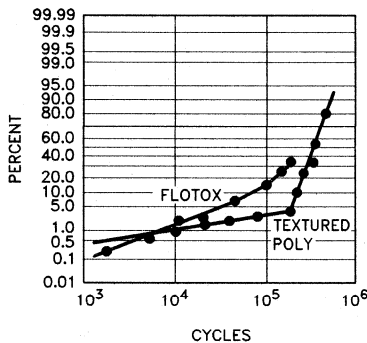
TABLE I: RETENTION COMPARISON OF INTEL EPROM AND E<sup>2</sup>PROM, AND XICOR E<sup>2</sup>PROM

Product	Technology	Sample	Temp	% Fail in Retention Bake			
				48 Hrs	168 Hrs	500 Hrs	1000 Hrs
I 2764A	EPROM	1800	250°C	0.9%*	1.1%	2.0%	—
I 2817A	FLOTOX	550	150°C	0.0%	0.0%	0.2%	0.2%*
X2864G	Textured Poly	350	250°C	0.0%*	0.0%	0.0%	0.3%

\*Represents ~ 15 Years at 55°C (E<sub>A</sub> = 0.6eV).

turn compare favorably with those of non-floating gate technologies. E<sup>2</sup>PROMs compare favorably with EPROMs because they are very similar technologies. It is only during endurance cycling that E<sup>2</sup>PROM operation differs significantly from EPROM operation. EPROMs and E<sup>2</sup>PROMs compare favorably with static logic devices because the nonvolatile devices are built on high voltage technologies and are operated during product testing at high voltages. This all but guarantees that there will be no oxide breakdown failures during 5V operation. Static logic devices generally are dominated by oxide breakdown. In addition to the Intel data above, NEC has reported that 65% of field failures from 1976 to 1979 were due to oxide failure.

## ENDURANCE CHARACTERISTICS



0024-1

Figure 1: Percent fail vs. number of cycles at room temperature for FLOTOX (2816A, 2817A) and Textured Poly (2864).

FLOTOX endurance, as shown in Figure 1, has a single broad distribution of failures. Textured Poly endurance has a low level defect tail followed by a sharp wearout beyond 150K cycles. The curves imply that the Textured Poly approach offers a trade-off under which a lower defect tail can be had at the expense of some wearout endurance. There are 3 primary failure mechanisms represented in Figure 1:

- 1) Tunnel Oxide Breakdown—the dominant FLOTOX mechanism, also responsible for part of the Textured Poly defect tail.
- 2) Gate Oxide Breakdown—responsible for the remainder of the Textured Poly defect tail.

3) Window Closing—the cause of Textured Poly wearout.

These three mechanisms will be discussed in turn.

## ENDURANCE: TUNNEL OXIDE BREAKDOWN

A typical FLOTOX or Textured Poly cell can be cycled over a million times without oxide failure or any degradation in retention characteristics. Occasional defective tunnel oxides will eventually break down under the high electric field ( $\sim 10$  MV/cm) necessary for tunneling. When this occurs, the defective cell will either become stuck to one logic state (if the oxide is truly shorted) or fail to retain charge (if the oxide is only leaky). Generally, the oxide breakdown increases gradually with cycling—a bit becomes leaky slowly, then faster, and eventually it becomes stuck. Tunnel oxide breakdown is responsible for about half of the Textured Poly defect tail. It displays the same characteristics as FLOTOX.

## ENDURANCE: GATE OXIDE BREAKDOWN

Both E<sup>2</sup>PROM types require high voltages to program and erase. This puts high stress on MOS gate oxides both in the cell and in the logic circuitry using high voltage. This high stress causes defective gate oxides to break down. Typical symptoms are a row or column failure or failure of the entire device. This failure mechanism is responsible for the remainder of the Textured Poly defect tail.

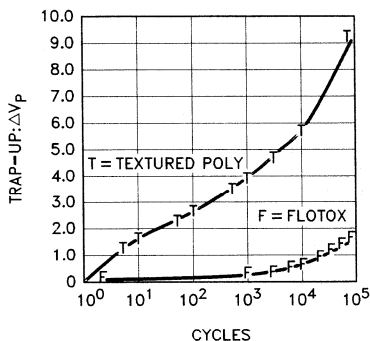
Although more common on Textured Poly than on FLOTOX because of somewhat higher voltages, the overall oxide breakdown failure rate of Textured Poly (tunnel oxide plus gate oxide) is still significantly lower than that of FLOTOX.

## ENDURANCE: WINDOW CLOSING

During endurance cycling, some of the electrons tunneling through the tunnel oxides become trapped there. The resulting negative oxide charge inhibits further tunneling. The effect of this electron trapping

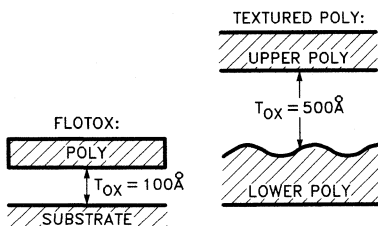
is that with further cycling a cell requires higher and higher voltages to program and erase. This mechanism is responsible for the entire wearout region of the Textured Poly curve but is non-existent in the FLOTOX curve.

In Figure 2 Textured Poly shows a dramatically higher rate of trap-up. As a result, window closing is the dominant wearout mechanism of Textured Poly, whereas it is an issue of FLOTOX only if the circuit design is marginal.



0024-2  
Figure 2: Trap-up vs. cycles for Textured Poly (2864) and FLOTOX (2816A). Trap-up is measured in terms of the increase in programming voltage  $\Delta V_p$  necessary to program the cell.

## TRAP-UP/BREAKDOWN TRADEOFF



0024-3  
Figure 3: FLOTOX and Textured Poly structures.

Trap-up is greater in the Textured Poly approach because:

- 1) The trapping probability for a single electron is proportional to  $N\sigma T_{OX}$ , which for the same trap density  $N$  and cross-section  $\sigma$  is greater for Textured Poly, since  $T_{OX}$  is greater.

- 2) The effect of the trapped charge is multiplied by the same field acceleration factor responsible for the field enhancement used for tunneling.
- 3) There is less field induced detrapping because the average electric field is lower.

Tunnel oxide breakdown is less frequent in the Textured Poly approach because:

- 1) The tunnel oxides are thicker and therefore are less sensitive to microscopic defects.
- 2) The high electric field responsible for tunneling occurs only in the region of oxide near texture points; the bulk of the oxide sees only low field stress.

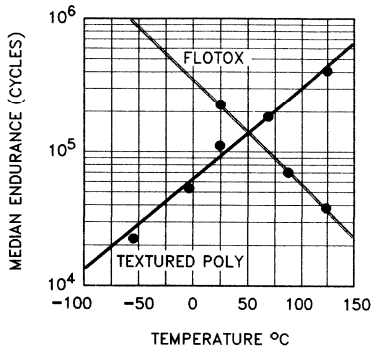
The trap-up/breakdown tradeoff is fundamental to the Textured Poly approach.

## BENEFITS OF THE TRADEOFF

Trap-up is an intrinsic mechanism, determined by trap density, trap cross-section, and initial window size. There is some variation from cell to cell in these parameters, causing some to fail somewhat earlier than others, but the distribution is relatively tight. As a result, trap-up endurance becomes only slightly worse with increasing memory size.

In contrast, oxide breakdown is a defect mechanism, and the failure rate is proportional to the defect density and the memory size. As a result, FLOTOX endurance will always become proportionately worse with increasing memory size unless defect density is continually improved. In addition, scaling FLOTOX implies scaling the tunnel oxide thickness, making the oxide even more sensitive to defects.

For this reason, there is a crossover in reliability between FLOTOX and Textured Poly, with the Textured Poly tradeoff becoming favorable at high densities. Excellent endurance even at high densities is possible with the Textured Poly approach because the defect tail, being only low level, can be screened.



0024-4

Figure 4: Comparison of median endurance for FLOTOX (2816A) and Textured Poly (2212) as a function of cycling temperature.

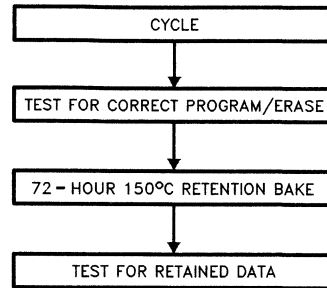
FLOTOX failure, due to tunnel oxide breakdown, is accelerated by cycling temperature ( $E_A \sim 0.18\text{eV}$ ), as shown in Figure 3. Textured Poly failure, due to window closing, is decelerated by cycling temperature ( $E_A \sim -0.11\text{eV}$ ). Whereas it is well known that temperature accelerates oxide breakdown, it also accelerates detrapping of electrons and therefore extends Textured Poly endurance.

A reliability evaluation of these two products performed at 50°C would detect equivalent median endurences, but an evaluation performed at room temperature would favor FLOTOX by about 5× and one at 125°C would favor Textured Poly by about 10×. This temperature acceleration holds true for the median endurance, but the Textured Poly defect tail is due to oxide breakdown and will tend to behave more like the FLOTOX data.

## EFFECT OF BAKES

In many FLOTOX endurance evaluations, less than half of the oxide breakdown failures actually

fail to program correctly. The remainder are cases of oxide degradation and suffer reduced retention instead. As a result, retention bakes must be performed *after* cycling on FLOTOX in order to adequately detect cycling failures:



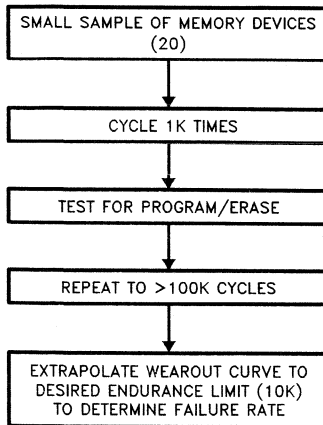
0024-5

In order to take intermediate readouts (after, say, 2K and 5K cycles), the flow of test/bake/test may be repeated at each readout. This worst-case flow for FLOTOX may be best-case for Textured Poly, however, because high temperature retention bakes cause electrons to detrapp significantly, reversing prior window closing and therefore increasing measured endurance.

## SUGGESTED ENDURANCE-EVALUATION METHODOLOGY

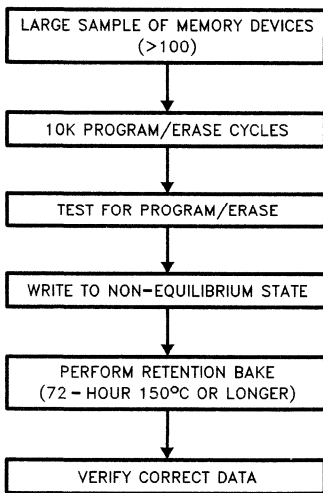
The best way to measure E<sup>2</sup>PROM endurance is to run separate evaluations for the two dominant failure mechanisms: window closing and oxide breakdown.

## Window Closing



0024-6

## Oxide Breakdown



0024-7

These flows will work for either FLOTOX or Textured Poly. Intermediate readouts may be performed in the oxide breakdown flow, but the test/bake/verify sequence should be repeated at each readout.

## ALTERNATIVE EVALUATION METHODOLOGIES

Single-cell endurance data are sometimes presented by manufacturers. This approach will overestimate endurance by orders of magnitude because of the importance of oxide defects and even cell-to-cell variations in trap-up. It might be possible to conclude from single-cell data that a certain FLOTOX cell is "superior" to a certain Textured Poly cell—but a 256K E<sup>2</sup>PROM constructed with the Textured Poly cell might be several times more reliable.

Worse yet, test pattern data from oxide capacitors are sometimes presented, without backup product data, to "prove" that a certain oxide is "superior" to another. Only product data can reliably be used to compare E<sup>2</sup>PROM product endurance. Small samples are useful in measuring wearout (median endurance), but large samples are necessary for measuring defect-related tails to the distribution.

## CONCLUSION

The non-endurance-related reliability of FLOTOX and Textured Poly E<sup>2</sup>PROMs are similar and comparable to EPROMs and simple logic devices. Textured Poly offers a tradeoff between oxide breakdown and window closing which is beneficial at high densities. Reliability evaluations should distinguish between the two dominant E<sup>2</sup>PROM failure mechanisms: Namely, oxide breakdown and window closing.

---

## NOTES

Ordering Information .....	9-1
Packaging Information .....	9-19
Sales Offices .....	9-32

**NOVRAM\* Data Sheets**

**1**

**Serial I/O Data Sheets**

**2**

**E<sup>2</sup>PROM Data Sheets**

**3**

**E<sup>2</sup>POT™ Digitally Controlled  
Potentiometer Data Sheets**

**4**

**Die Products**

**5**

**Military**

**6**

**Applications**

**7**

**Reliability**

**8**

**General Information**

**9**







# Ordering Information for Xicor Nonvolatile Memories

## NOVRAMS\*

Device Order Number	Organization	Package						Temp. Range	Store Cycles/ Data Changes Per Bit	Access Time	Processing Level
		P	J	D	E	G	C				
X2201AD	1024 x 1			•				†	10,000/1000	300 ns	Standard
X2210P/10	64 x 4	•						†	100,000/10,000	300 ns	Standard
X2210P/5	64 x 4	•						†	50,000/5000	300 ns	Standard
X2210P	64 x 4	•						†	10,000/1000	300 ns	Standard
X2210PI/10	64 x 4	•						I	100,000/10,000	300 ns	Standard
X2210PI/5	64 x 4	•						I	50,000/5000	300 ns	Standard
X2210PI	64 x 4	•						I	10,000/1000	300 ns	Standard
X2210D/10	64 x 4			•				†	100,000/1000	300 ns	Standard
X2210D/5	64 x 4			•				†	50,000/5000	300 ns	Standard
X2210D	64 x 4			•				†	10,000/1000	300 ns	Standard
X2210DI/10	64 x 4			•				I	100,000/10,000	300 ns	Standard
X2210DI/5	64 x 4			•				I	50,000/5000	300 ns	Standard
X2210DI	64 x 4			•				I	10,000/1000	300 ns	Standard
X2210DM/10	64 x 4			•				M	100,000/10,000	300 ns	Standard
X2210DM/5	64 x 4			•				M	50,000/5000	300 ns	Standard
X2210DM	64 x 4			•				M	10,000/1000	300 ns	Standard
X2210DMB/10	64 x 4			•				M	100,000/10,000	300 ns	883 Level C
X2210DMB/5	64 x 4			•				M	50,000/5000	300 ns	883 Level C
X2210DMB	64 x 4			•				M	10,000/1000	300 ns	883 Level C
X2212P/10	256 x 4	•						†	100,000/10,000	300 ns	Standard
X2212P/5	256 x 4	•						†	50,000/5000	300 ns	Standard

### Key:

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

\*NOVRAM is Xicor's nonvolatile static RAM device.

## Ordering Information for Xicor Nonvolatile Memories

### NOVRAMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Store Cycles/ Data Changes Per Bit	Access Time	Processing Level
		P	J	D	E	G	C				
X2212P	256 x 4	•						†	10,000/1000	300 ns	Standard
X2212PI/10	256 x 4	•						I	100,000/10,000	300 ns	Standard
X2212PI/5	256 x 4	•						I	50,000/5000	300 ns	Standard
X2212PI	256 x 4	•						I	10,000/1000	300 ns	Standard
X2212D/10	256 x 4			•				†	100,000/10,000	300 ns	Standard
X2212D/5	256 x 4			•				†	50,000/5000	300 ns	Standard
X2212D	256 x 4			•				†	10,000/1000	300 ns	Standard
X2212DI/10	256 x 4			•				I	100,000/10,000	300 ns	Standard
X2212DI/5	256 x 4			•				I	50,000/5000	300 ns	Standard
X2212DI	256 x 4			•				I	10,000/1000	300 ns	Standard
X2212DM/10	256 x 4			•				M	100,000/10,000	300 ns	Standard
X2212DM/5	256 x 4			•				M	50,000/5000	300 ns	Standard
X2212DM	256 x 4			•				M	10,000/1000	300 ns	Standard
X2212DMB/10	256 x 4			•				M	100,000/10,000	300 ns	883 Level C
X2212DMB/5	256 x 4			•				M	50,000/5000	300 ns	883 Level C
X2212DMB	256 x 4			•				M	10,000/1000	300 ns	883 Level C

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### NOVRAMs (Byte-Wide)

Device Order Number	Organization	Package						Temp. Range	Store Cycles	Access Time	Processing Level
		P	J	D	E	G	C				
X2001P-20	128 x 8	•						†	10,000	200 ns	Standard
X2001P-25	128 x 8	•						†	10,000	250 ns	Standard
X2001P	128 x 8	•						†	10,000	300 ns	Standard
X2001PI-20	128 x 8	•						I	10,000	200 ns	Standard
X2001PI-25	128 x 8	•						I	10,000	250 ns	Standard
X2001PI	128 x 8	•						I	10,000	300 ns	Standard
X2001D-20	128 x 8			•				†	10,000	200 ns	Standard
X2001D-25	128 x 8			•				†	10,000	250 ns	Standard
X2001D	128 x 8			•				†	10,000	300 ns	Standard
X2001DI-20	128 x 8			•				I	10,000	200 ns	Standard
X2001DI-25	128 x 8			•				I	10,000	250 ns	Standard
X2001DI	128 x 8			•				I	10,000	300 ns	Standard
X2004D-20	512 x 8			•				†	10,000	200 ns	Standard
X2004D-25	512 x 8			•				†	10,000	250 ns	Standard
X2004D	512 x 8			•				†	10,000	300 ns	Standard
X2004DI-20	512 x 8			•				I	10,000	200 ns	Standard
X2004DI-25	512 x 8			•				I	10,000	250 ns	Standard
X2004DI	512 x 8			•				I	10,000	300 ns	Standard
X2004DM-20	512 x 8			•				M	10,000	200 ns	Standard
X2004DM-25	512 x 8			•				M	10,000	250 ns	Standard
X2004DM	512 x 8			•				M	10,000	300 ns	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### NOVRAMs (Byte-Wide) (Continued)

Device Order Number	Organization	Package						Temp. Range	Store Cycles	Access Time	Processing Level
		P	J	D	E	G	C				
X2004DMB-20	512 x 8			•				M	10,000	200 ns	883 Level C
X2004DMB-25	512 x 8			•				M	10,000	250 ns	883 Level C
X2004DMB	512 x 8			•				M	10,000	300 ns	883 Level C
X2004E-20	512 x 8				•			†	10,000	200 ns	Standard
X2004E-25	512 x 8				•			†	10,000	250 ns	Standard
X2004E	512 x 8				•			†	10,000	300 ns	Standard
X2004EI-20	512 x 8				•			I	10,000	200 ns	Standard
X2004EI-25	512 x 8				•			I	10,000	250 ns	Standard
X2004EI	512 x 8				•			I	10,000	300 ns	Standard
X2004EM-20	512 x 8				•			M	10,000	200 ns	Standard
X2004EM-25	512 x 8				•			M	10,000	250 ns	Standard
X2004EM	512 x 8				•			M	10,000	300 ns	Standard
X2004EMB-20	512 x 8				•			M	10,000	200 ns	883 Level C
X2004EMB-25	512 x 8				•			M	10,000	250 ns	883 Level C
X2004EMB	512 x 8				•			M	10,000	300 ns	883 Level C
X2004J-20	512 x 8		•					†	10,000	200 ns	Standard
X2004J-25	512 x 8		•					†	10,000	250 ns	Standard
X2004J	512 x 8		•					†	10,000	300 ns	Standard
X2004JI-20	512 x 8		•					I	10,000	200 ns	Standard
X2004JI-25	512 x 8		•					I	10,000	250 ns	Standard
X2004JI	512 x 8		•					I	10,000	300 ns	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Ordering Information for Xicor Nonvolatile Memories

## SERIAL NOVRAMs

Device Order Number	Organization	Package						Temp. Range	Process Technology	Processing Level
		P	J	D	E	G	C			
X2444P	16 x 16	•						†	NMOS	Standard
X2444PI	16 x 16	•						I	NMOS	Standard
X2444PM	16 x 16	•						M	NMOS	Standard

## SERIAL E<sup>2</sup>PROMs

Device Order Number	Organization	Package						Temp. Range	Process Technology	Processing Level
		P	J	D	E	G	C			
X2402P	256 x 8	•						†	NMOS	Standard
X2402PI	256 x 8	•						I	NMOS	Standard
X2404P	512 x 8	•						†	NMOS	Standard
X2404PI	512 x 8	•						I	NMOS	Standard
X2404D	512 x 8			•				†	NMOS	Standard
X2404DI	512 x 8			•				I	NMOS	Standard
X2404DM	512 x 8			•				M	NMOS	Standard
X2404DMB	512 x 8			•				M	NMOS	883 Level C
X24C04P	512 x 8	•						†	CMOS	Standard
X24C04PI	512 x 8	•						I	CMOS	Standard
X24C16P	2048 x 8	•						†	CMOS	Standard
X24C16PI	2048 x 8	•						I	CMOS	Standard
X24C16D	2048 x 8			•				†	CMOS	Standard
X24C16DI	2048 x 8			•				I	CMOS	Standard
X24C16DM	2048 x 8			•				M	CMOS	Standard
X24C16DMB	2048 x 8			•				M	CMOS	883 Level C

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 4K E<sup>2</sup>PROMs

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2804AP-25	512 x 8	•						†	250 ns	NMOS	Standard
X2804AP	512 x 8	•						†	300 ns	NMOS	Standard
X2804AP-35	512 x 8	•						†	350 ns	NMOS	Standard
X2804AP-45	512 x 8	•						†	450 ns	NMOS	Standard
X2804API	512 x 8	•							300 ns	NMOS	Standard
X2804API-35	512 x 8	•							350 ns	NMOS	Standard
X2804API-45	512 x 8	•							450 ns	NMOS	Standard
X2804AD-25	512 x 8			•				†	250 ns	NMOS	Standard
X2804AD	512 x 8			•				†	300 ns	NMOS	Standard
X2804AD-35	512 x 8			•				†	350 ns	NMOS	Standard
X2804AD-45	512 x 8			•				†	450 ns	NMOS	Standard
X2804ADI	512 x 8			•					300 ns	NMOS	Standard
X2804ADI-35	512 x 8			•					350 ns	NMOS	Standard
X2804ADI-45	512 x 8			•					450 ns	NMOS	Standard
X2804ADM	512 x 8			•				M	300 ns	NMOS	Standard
X2804ADM-35	512 x 8			•				M	350 ns	NMOS	Standard
X2804ADM-45	512 x 8			•				M	450 ns	NMOS	Standard
X2804ADMB	512 x 8			•				M	300 ns	NMOS	883 Level C
X2804ADMB-35	512 x 8			•				M	350 ns	NMOS	883 Level C
X2804ADMB-45	512 x 8			•				M	450 ns	NMOS	883 Level C

**Key:**

† = Blank = Commercial = 0°C to +70°C

| = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 16K E<sup>2</sup>PROMs

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2816AP-25	2048 x 8	•						†	250 ns	NMOS	Standard
X2816AP	2048 x 8	•						†	300 ns	NMOS	Standard
X2816AP-35	2048 x 8	•						†	350 ns	NMOS	Standard
X2816AP-45	2048 x 8	•						†	450 ns	NMOS	Standard
X2816API-25	2048 x 8	•							250 ns	NMOS	Standard
X2816API	2048 x 8	•							300 ns	NMOS	Standard
X2816API-35	2048 x 8	•							350 ns	NMOS	Standard
X2816API-45	2048 x 8	•							450 ns	NMOS	Standard
X2816AD-25	2048 x 8			•				†	250 ns	NMOS	Standard
X2816AD	2048 x 8			•				†	300 ns	NMOS	Standard
X2816AD-35	2048 x 8			•				†	350 ns	NMOS	Standard
X2816AD-45	2048 x 8			•				†	450 ns	NMOS	Standard
X2816ADI-25	2048 x 8			•					250 ns	NMOS	Standard
X2816ADI	2048 x 8			•					300 ns	NMOS	Standard
X2816ADI-35	2048 x 8			•					350 ns	NMOS	Standard
X2816ADI-45	2048 x 8			•					450 ns	NMOS	Standard
X2816ADM	2048 x 8			•				M	300 ns	NMOS	Standard
X2816ADM-35	2048 x 8			•				M	350 ns	NMOS	Standard
X2816ADM-45	2048 x 8			•				M	450 ns	NMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C

| = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 16K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2816ADMB	2048 x 8			•				M	300 ns	NMOS	883 Level C
X2816ADMB-35	2048 x 8			•				M	350 ns	NMOS	883 Level C
X2816ADMB-45	2048 x 8			•				M	450 ns	NMOS	883 Level C
X2816AE-25	2048 x 8				•			†	250 ns	NMOS	Standard
X2816AE	2048 x 8				•			†	300 ns	NMOS	Standard
X2816AE-35	2048 x 8				•			†	350 ns	NMOS	Standard
X2816AE-45	2048 x 8				•			†	450 ns	NMOS	Standard
X2816AEI-25	2048 x 8				•			I	250 ns	NMOS	Standard
X2816AEI	2048 x 8				•			I	300 ns	NMOS	Standard
X2816AEI-35	2048 x 8				•			I	350 ns	NMOS	Standard
X2816AEI-45	2048 x 8				•			I	450 ns	NMOS	Standard
X2816AEM	2048 x 8				•			M	300 ns	NMOS	Standard
X2816AEM-35	2048 x 8				•			M	350 ns	NMOS	Standard
X2816AEM-45	2048 x 8				•			M	450 ns	NMOS	Standard
X2816AEMB	2048 x 8				•			M	300 ns	NMOS	883 Level C
X2816AEMB-35	2048 x 8				•			M	350 ns	NMOS	883 Level C
X2816AEMB-45	2048 x 8				•			M	450 ns	NMOS	883 Level C

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze



## Ordering Information for Xicor Nonvolatile Memories

### 16K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2816BP-25	2048 x 8	•						†	250 ns	NMOS	Standard
X2816BP	2048 x 8	•						†	300 ns	NMOS	Standard
X2816BPI-25	2048 x 8	•						I	250 ns	NMOS	Standard
X2816BPI	2048 x 8	•						I	300 ns	NMOS	Standard
X2816BD-25	2048 x 8			•				†	250 ns	NMOS	Standard
X2816BD	2048 x 8			•				†	300 ns	NMOS	Standard
X2816BDI-25	2048 x 8			•				I	250 ns	NMOS	Standard
X2816BDI	2048 x 8			•				I	300 ns	NMOS	Standard
X2816BDM-25	2048 x 8			•				M	250 ns	NMOS	Standard
X2816BDM	2048 x 8			•				M	300 ns	NMOS	Standard
X2816BDMB-25	2048 x 8			•				M	250 ns	NMOS	883 Level C
X2816BDMB	2048 x 8			•				M	300 ns	NMOS	883 Level C
X2816BE-25	2048 x 8				•			†	250 ns	NMOS	Standard
X2816BE	2048 x 8				•			†	300 ns	NMOS	Standard
X2816BEI-25	2048 x 8				•			I	250 ns	NMOS	Standard
X2816BEI	2048 x 8				•			I	300 ns	NMOS	Standard
X2816BEM-25	2048 x 8				•			M	250 ns	NMOS	Standard
X2816BEM	2048 x 8				•			M	300 ns	NMOS	Standard
X2816BEMB-25	2048 x 8				•			M	250 ns	NMOS	883 Level C
X2816BEMB	2048 x 8				•			M	300 ns	NMOS	883 Level C
X2816BJ-25	2048 x 8		•					†	250 ns	NMOS	Standard
X2816BJ	2048 x 8		•					†	300 ns	NMOS	Standard
X2816BJI-25	2048 x 8		•					I	250 ns	NMOS	Standard
X2816BJI	2048 x 8		•					I	300 ns	NMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 64K E<sup>2</sup>PROMs

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864AP-25	8192 x 8	•						†	250 ns	NMOS	Standard
X2864AP	8192 x 8	•						†	300 ns	NMOS	Standard
X2864AP-35	8192 x 8	•						†	350 ns	NMOS	Standard
X2864AP-45	8192 x 8	•						†	450 ns	NMOS	Standard
X2864API-25	8192 x 8	•							250 ns	NMOS	Standard
X2864API	8192 x 8	•							300 ns	NMOS	Standard
X2864API-35	8192 x 8	•							350 ns	NMOS	Standard
X2864API-45	8192 x 8	•							450 ns	NMOS	Standard
X2864AD-25	8192 x 8			•				†	250 ns	NMOS	Standard
X2864AD	8192 x 8			•				†	300 ns	NMOS	Standard
X2864AD-35	8192 x 8			•				†	350 ns	NMOS	Standard
X2864AD-45	8192 x 8			•				†	450 ns	NMOS	Standard
X2864ADI-25	8192 x 8			•					250 ns	NMOS	Standard
X2864ADI	8192 x 8			•					300 ns	NMOS	Standard
X2864ADI-35	8192 x 8			•					350 ns	NMOS	Standard
X2864ADI-45	8192 x 8			•					450 ns	NMOS	Standard
X2864ADM-25	8192 x 8			•				M	250 ns	NMOS	Standard
X2864ADM	8192 x 8			•				M	300 ns	NMOS	Standard
X2864ADM-35	8192 x 8			•				M	350 ns	NMOS	Standard
X2864ADM-45	8192 x 8			•				M	450 ns	NMOS	Standard
X2864ADMB-25	8192 x 8			•				M	250 ns	NMOS	883 Level C
X2864ADMB	8192 x 8			•				M	300 ns	NMOS	883 Level C
X2864ADMB-35	8192 x 8			•				M	350 ns	NMOS	883 Level C
X2864ADMB-45	8192 x 8			•				M	450 ns	NMOS	883 Level C

**Key:**

† = Blank = Commercial = 0°C to +70°C

| = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Ordering Information for Xicor Nonvolatile Memories

## 64K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864AE-25	8192 x 8				•			†	250 ns	NMOS	Standard
X2864AE	8192 x 8				•			†	300 ns	NMOS	Standard
X2864AE-35	8192 x 8				•			†	350 ns	NMOS	Standard
X2864AE-45	8192 x 8				•			†	450 ns	NMOS	Standard
X2864AEI-25	8192 x 8				•			I	250 ns	NMOS	Standard
X2864AEI	8192 x 8				•			I	300 ns	NMOS	Standard
X2864AEI-35	8192 x 8				•			I	350 ns	NMOS	Standard
X2864AEI-45	8192 x 8				•			I	450 ns	NMOS	Standard
X2864AEM-25	8192 x 8				•			M	250 ns	NMOS	Standard
X2864AEM	8192 x 8				•			M	300 ns	NMOS	Standard
X2864AEM-35	8192 x 8				•			M	350 ns	NMOS	Standard
X2864AEM-45	8192 x 8				•			M	450 ns	NMOS	Standard
X2864AEMB-25	8192 x 8				•			M	250 ns	NMOS	883 Level C
X2864AEMB	8192 x 8				•			M	300 ns	NMOS	883 Level C
X2864AEMB-35	8192 x 8				•			M	350 ns	NMOS	883 Level C
X2864AEMB-45	8192 x 8				•			M	450 ns	NMOS	883 Level C
X2864AGM-25	8192 x 8					•		M	250 ns	NMOS	Standard
X2864AGM	8192 x 8					•		M	300 ns	NMOS	Standard
X2864AGM-35	8192 x 8					•		M	350 ns	NMOS	Standard
X2864AGM-45	8192 x 8					•		M	450 ns	NMOS	Standard
X2864AGMB-25	8192 x 8					•		M	250 ns	NMOS	883 Level C
X2864AGMB	8192 x 8					•		M	300 ns	NMOS	883 Level C
X2864AGMB-35	8192 x 8					•		M	350 ns	NMOS	883 Level C
X2864AGMB-45	8192 x 8					•		M	450 ns	NMOS	883 Level C

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 64K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864AJ-25	8192 x 8		•					†	250 ns	NMOS	Standard
X2864AJ	8192 x 8		•					†	300 ns	NMOS	Standard
X2864AJ-35	8192 x 8		•					†	350 ns	NMOS	Standard
X2864AJ-45	8192 x 8		•					†	450 ns	NMOS	Standard
X2864AJI-25	8192 x 8		•					l	250 ns	NMOS	Standard
X2864AJI	8192 x 8		•					l	300 ns	NMOS	Standard
X2864AJI-35	8192 x 8		•					l	350 ns	NMOS	Standard
X2864AJI-45	8192 x 8		•					l	450 ns	NMOS	Standard
X2864ADT-35	8192 x 8			•				T	350 ns	NMOS	Standard
X2864ADT-45	8192 x 8			•				T	450 ns	NMOS	Standard
X2864AET-35	8192 x 8				•			T	350 ns	NMOS	Standard
X2864AET-45	8192 x 8				•			T	450 ns	NMOS	Standard

### 64K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864BP-12	8192 x 8	•						†	120 ns	NMOS	Standard
X2864BP-15	8192 x 8	•						†	150 ns	NMOS	Standard
X2864BP-18	8192 x 8	•						†	180 ns	NMOS	Standard
X2864BPI-12	8192 x 8	•						l	120 ns	NMOS	Standard
X2864BPI-15	8192 x 8	•						l	150 ns	NMOS	Standard
X2864BPI-18	8192 x 8	•						l	180 ns	NMOS	Standard
X2864BD-12	8192 x 8			•				†	120 ns	NMOS	Standard
X2864BD-15	8192 x 8			•				†	150 ns	NMOS	Standard
X2864BD-18	8192 x 8			•				†	180 ns	NMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 l = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 64K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864BDI-12	8192 x 8			•				I	120 ns	NMOS	Standard
X2864BDI-15	8192 x 8			•				I	150 ns	NMOS	Standard
X2864BDI-18	8192 x 8			•				I	180 ns	NMOS	Standard
X2864BDM-12	8192 x 8			•				M	120 ns	NMOS	Standard
X2864BDM-15	8192 x 8			•				M	150 ns	NMOS	Standard
X2864BDM-18	8192 x 8			•				M	180 ns	NMOS	Standard
X2864BDMB-12	8192 x 8			•				M	120 ns	NMOS	883 Level C
X2864BDMB-15	8192 x 8			•				M	150 ns	NMOS	883 Level C
X2864BDMB-18	8192 x 8			•				M	180 ns	NMOS	883 Level C
X2864BE-12	8192 x 8				•			†	120 ns	NMOS	Standard
X2864BE-15	8192 x 8				•			†	150 ns	NMOS	Standard
X2864BE-18	8192 x 8				•			†	180 ns	NMOS	Standard
X2864BEI-12	8192 x 8				•			I	120 ns	NMOS	Standard
X2864BEI-15	8192 x 8				•			I	150 ns	NMOS	Standard
X2864BEI-18	8192 x 8				•			I	180 ns	NMOS	Standard
X2864BEM-12	8192 x 8				•			M	120 ns	NMOS	Standard
X2864BEM-15	8192 x 8				•			M	150 ns	NMOS	Standard
X2864BEM-18	8192 x 8				•			M	180 ns	NMOS	Standard
X2864BEMB-12	8192 x 8				•			M	120 ns	NMOS	883 Level C
X2864BEMB-15	8192 x 8				•			M	150 ns	NMOS	883 Level C
X2864BEMB-18	8192 x 8				•			M	180 ns	NMOS	883 Level C
X2864BJ-12	8192 x 8		•					†	120 ns	NMOS	Standard
X2864BJ-15	8192 x 8		•					†	150 ns	NMOS	Standard
X2864BJ-18	8192 x 8		•					†	180 ns	NMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Leaded Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

# Ordering Information for Xicor Nonvolatile Memories

## 64K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864BJI-12	8192 x 8		•					I	120 ns	NMOS	Standard
X2864BJI-15	8192 x 8		•					I	150 ns	NMOS	Standard
X2864BJI-18	8192 x 8		•					I	180 ns	NMOS	Standard

## 64K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X2864HP-70	8192 x 8	•						†	70 ns	NMOS	Standard
X2864HP-90	8192 x 8	•						†	90 ns	NMOS	Standard
X2864HPI-90	8192 x 8	•						I	90 ns	NMOS	Standard
X2864HD-70	8192 x 8			•				†	70 ns	NMOS	Standard
X2864HD-90	8192 x 8			•				†	90 ns	NMOS	Standard
X2864HDI-90	8192 x 8			•				I	90 ns	NMOS	Standard
X2864HDM-90	8192 x 8			•				M	90 ns	NMOS	Standard
X2864HDMB-90	8192 x 8			•				M	90 ns	NMOS	883 Level C
X2864HE-70	8192 x 8				•			†	70 ns	NMOS	Standard
X2864HE-90	8192 x 8				•			†	90 ns	NMOS	Standard
X2864HEI-90	8192 x 8				•			I	90 ns	NMOS	Standard
X2864HEM-90	8192 x 8				•			M	90 ns	NMOS	Standard
X2864HEMB-90	8192 x 8				•			M	90 ns	NMOS	883 Level C
X2864HJ-70	8192 x 8		•					†	70 ns	NMOS	Standard
X2864HJ-90	8192 x 8		•					†	90 ns	NMOS	Standard
X2864HJI-90	8192 x 8		•					I	90 ns	NMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 256K E<sup>2</sup>PROMs

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X28256P-25	32768 x 8	•						†	250 ns	NMOS	Standard
X28256P	32768 x 8	•						†	300 ns	NMOS	Standard
X28256P-35	32768 x 8	•						†	350 ns	NMOS	Standard
X28256PI-25	32768 x 8	•						l	250 ns	NMOS	Standard
X28256PI	32768 x 8	•						l	300 ns	NMOS	Standard
X28256PI-35	32768 x 8	•						l	350 ns	NMOS	Standard
X28256D-25	32768 x 8			•				†	250 ns	NMOS	Standard
X28256D	32768 x 8			•				†	300 ns	NMOS	Standard
X28256D-35	32768 x 8			•				†	350 ns	NMOS	Standard
X28256DI-25	32768 x 8			•				l	250 ns	NMOS	Standard
X28256DI	32768 x 8			•				l	300 ns	NMOS	Standard
X28256DI-35	32768 x 8			•				l	350 ns	NMOS	Standard
X28256DM-25	32768 x 8			•				M	250 ns	NMOS	Standard
X28256DM	32768 x 8			•				M	300 ns	NMOS	Standard
X28256DM-35	32768 x 8			•				M	350 ns	NMOS	Standard
X28256DMB-25	32768 x 8			•				M	250 ns	NMOS	883 Level C
X28256DMB	32768 x 8			•				M	300 ns	NMOS	883 Level C
X28256DMB-35	32768 x 8			•				M	350 ns	NMOS	883 Level C
X28256E-25	32768 x 8				•			†	250 ns	NMOS	Standard
X28256E	32768 x 8				•			†	300 ns	NMOS	Standard
X28256E-35	32768 x 8				•			†	350 ns	NMOS	Standard
X28256EI-25	32768 x 8				•			l	250 ns	NMOS	Standard
X28256EI	32768 x 8				•			l	300 ns	NMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 l = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 256K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X28256EI-35	32768 x 8				•			I	350 ns	NMOS	Standard
X28256EM-25	32768 x 8				•			M	250 ns	NMOS	Standard
X28256EM	32768 x 8				•			M	300 ns	NMOS	Standard
X28256EM-35	32768 x 8				•			M	350 ns	NMOS	Standard
X28256EMB-25	32768 x 8				•			M	250 ns	NMOS	883 Level C
X28256EMB	32768 x 8				•			M	300 ns	NMOS	883 Level C
X28256EMB-35	32768 x 8				•			M	350 ns	NMOS	883 Level C
X28256J-25	32768 x 8		•					†	250 ns	NMOS	Standard
X28256J	32768 x 8		•					†	300 ns	NMOS	Standard
X28256J-35	32768 x 8		•					†	350 ns	NMOS	Standard
X28256JI-25	32768 x 8		•					I	250 ns	NMOS	Standard
X28256JI	32768 x 8		•					I	300 ns	NMOS	Standard
X28256JI-35	32768 x 8		•					I	350 ns	NMOS	Standard

### 256K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X28C256P-25	32768 x 8	•						†	250 ns	CMOS	Standard
X28C256P	32768 x 8	•						†	300 ns	CMOS	Standard
X28C256P-35	32768 x 8	•						†	350 ns	CMOS	Standard
X28C256PI-25	32768 x 8	•						I	250 ns	CMOS	Standard
X28C256PI	32768 x 8	•						I	300 ns	CMOS	Standard
X28C256PI-35	32768 x 8	•						I	350 ns	CMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze



## Ordering Information for Xicor Nonvolatile Memories

### 256K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X28C256D-25	32768 x 8			•				†	250 ns	CMOS	Standard
X28C256D	32768 x 8			•				†	300 ns	CMOS	Standard
X28C256D-35	32768 x 8			•				†	350 ns	CMOS	Standard
X28C256DI-25	32768 x 8			•				I	250 ns	CMOS	Standard
X28C256DI	32768 x 8			•				I	300 ns	CMOS	Standard
X28C256DI-35	32768 x 8			•				I	350 ns	CMOS	Standard
X28C256DM-25	32768 x 8			•				M	250 ns	CMOS	Standard
X28C256DM	32768 x 8			•				M	300 ns	CMOS	Standard
X28C256DM-35	32768 x 8			•				M	350 ns	CMOS	Standard
X28C256DMB-25	32768 x 8			•				M	250 ns	CMOS	883 Level C
X28C256DMB	32768 x 8			•				M	300 ns	CMOS	883 Level C
X28C256DMB-35	32768 x 8			•				M	350 ns	CMOS	883 Level C
X28C256E-25	32768 x 8				•			†	250 ns	CMOS	Standard
X28C256E	32768 x 8				•			†	300 ns	CMOS	Standard
X28C256E-35	32768 x 8				•			†	350 ns	CMOS	Standard
X28C256EI-25	32768 x 8				•			I	250 ns	CMOS	Standard
X28C256EI	32768 x 8				•			I	300 ns	CMOS	Standard
X28C256EI-35	32768 x 8				•			I	350 ns	CMOS	Standard
X28C256EM-25	32768 x 8				•			M	250 ns	CMOS	Standard
X28C256EM	32768 x 8				•			M	300 ns	CMOS	Standard
X28C256EM-35	32768 x 8				•			M	350 ns	CMOS	Standard

**Key:**

† = Blank = Commercial = 0°C to +70°C

I = Industrial = -40°C to +85°C

M = Military = -55°C to +125°C

T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP

J = 32-Lead J-Hook Plastic Ledged Chip Carrier

D = Cerdip

E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)

G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)

C = Side Braze

## Ordering Information for Xicor Nonvolatile Memories

### 256K E<sup>2</sup>PROMs (Continued)

Device Order Number	Organization	Package						Temp. Range	Access Time	Process Technology	Processing Level
		P	J	D	E	G	C				
X28C256EMB-25	32768 x 8				•			M	250 ns	CMOS	883 Level C
X28C256EMB	32768 x 8				•			M	300 ns	CMOS	883 Level C
X28C256EMB-35	32768 x 8				•			M	350 ns	CMOS	883 Level C
X28C256J-25	32768 x 8		•					†	250 ns	CMOS	Standard
X28C256J	32768 x 8		•					†	300 ns	CMOS	Standard
X28C256J-35	32768 x 8		•					†	350 ns	CMOS	Standard
X28C256JI-25	32768 x 8		•					I	250 ns	CMOS	Standard
X28C256JI	32768 x 8		•					I	300 ns	CMOS	Standard
X28C256JI-35	32768 x 8		•					I	350 ns	CMOS	Standard

### E<sup>2</sup>POTENTIOMETERS

Device Order Number	Maximum Resistance	Package						Temp. Range	Processing Level
		P	J	D	E	G	C		
X9103P	10 K $\Omega$	•						†	Standard
X9503P	50 K $\Omega$	•						†	Standard
X9104P	100 K $\Omega$	•						†	Standard
X9103PI	10 K $\Omega$	•						I	Standard
X9503PI	50 K $\Omega$	•						I	Standard
X9104PI	100 K $\Omega$	•						I	Standard
X9103PM	10 K $\Omega$	•						M	Standard
X9503PM	50 K $\Omega$	•						M	Standard
X9104PM	100 K $\Omega$	•						M	Standard

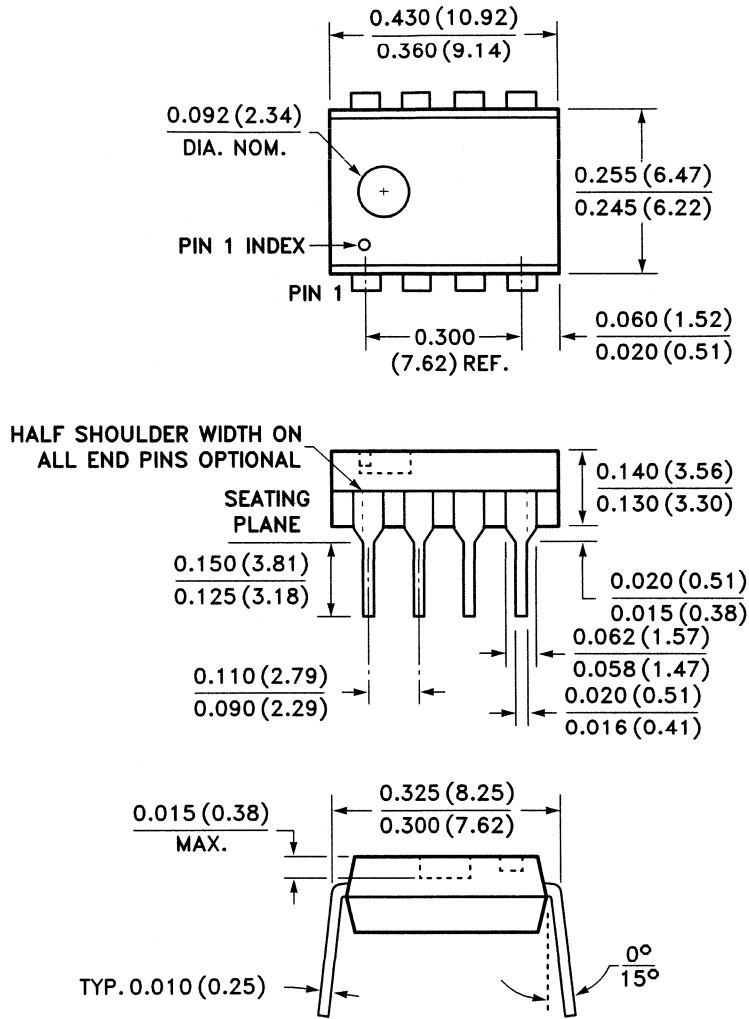
#### Key:

† = Blank = Commercial = 0°C to +70°C  
 I = Industrial = -40°C to +85°C  
 M = Military = -55°C to +125°C  
 T = Ultra High Temp. = 0°C to +150°C

P = Plastic DIP  
 J = 32-Lead J-Hook Plastic Leaded Chip Carrier  
 D = Cerdip  
 E = 32-Pad Ceramic Leadless Chip Carrier (Solder Seal)  
 G = 32-Pad Ceramic Leadless Chip Carrier (Glass Frit Seal)  
 C = Side Braze

# Packaging Information

## 8-LEAD PLASTIC DUAL IN-LINE PACKAGE TYPE P

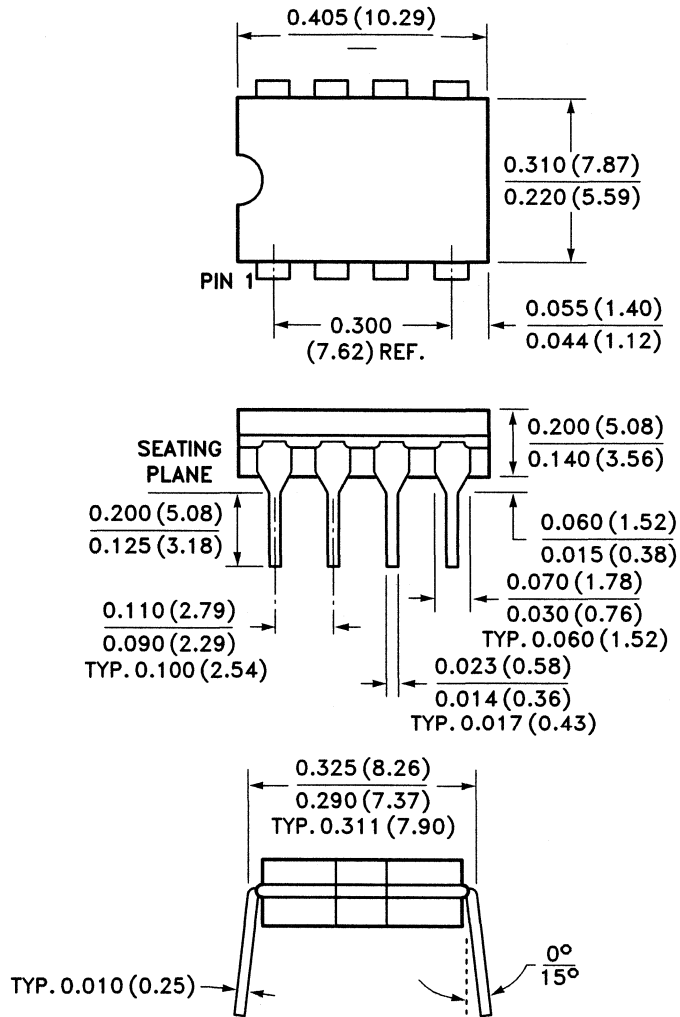


PPI008

NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

# Packaging Information

## 8-LEAD HERMETIC DUAL IN-LINE PACKAGE TYPE D

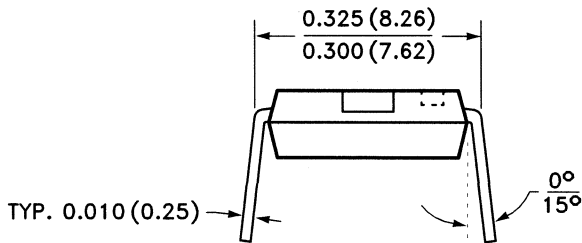
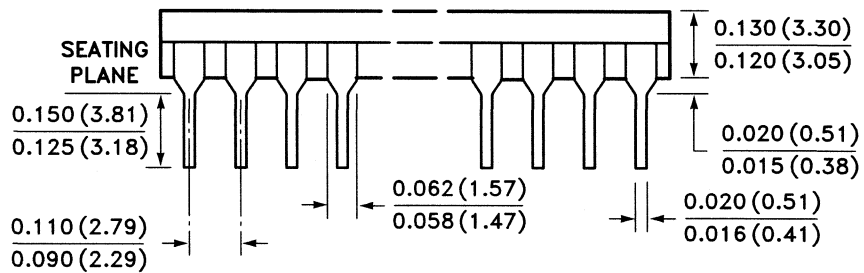
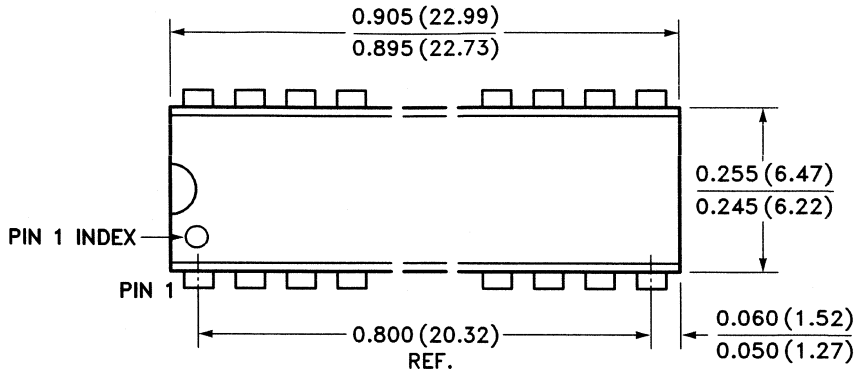


HDI008

**NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)**

# Packaging Information

## 18-LEAD PLASTIC DUAL IN-LINE PACKAGE TYPE P

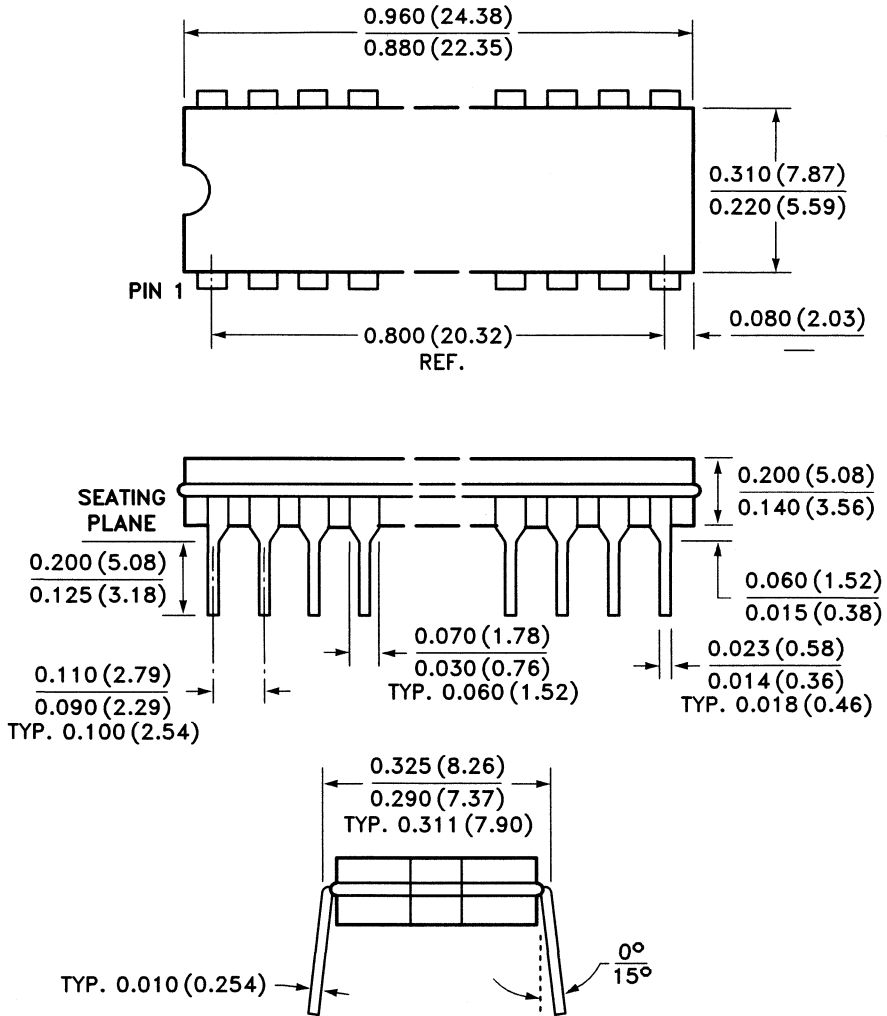


NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

PPI018

# Packaging Information

## 18-LEAD HERMETIC DUAL IN-LINE PACKAGE TYPE D

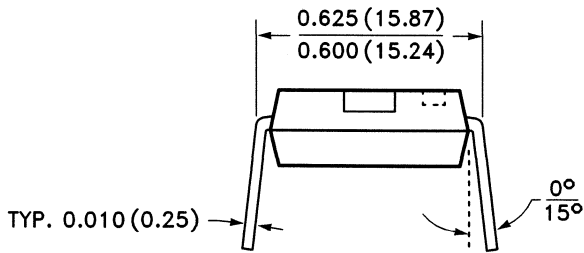
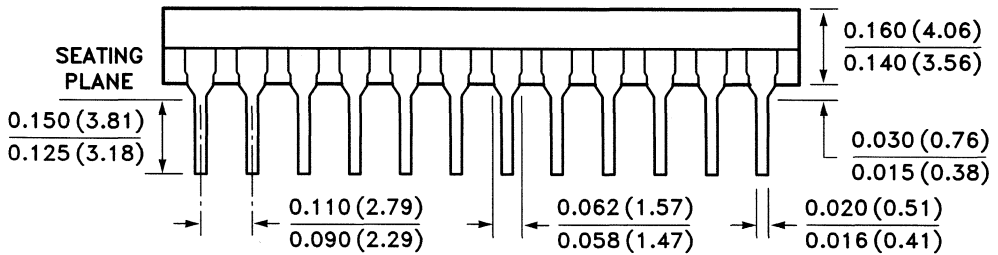
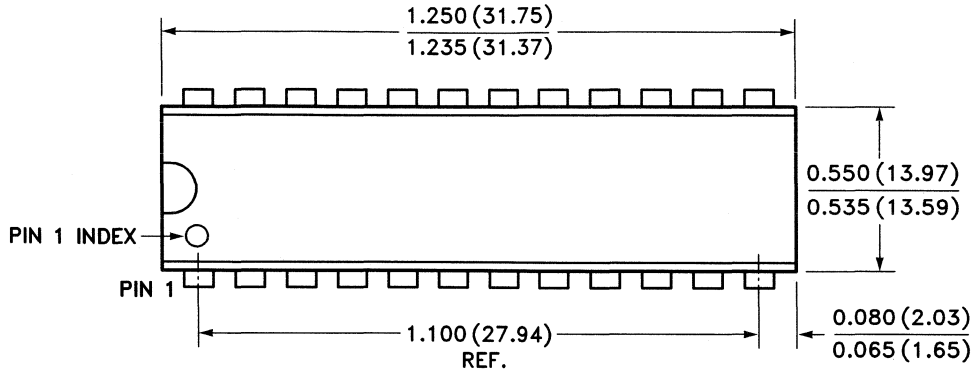


NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

HD1018

# Packaging Information

## 24-LEAD PLASTIC DUAL IN-LINE PACKAGE TYPE P

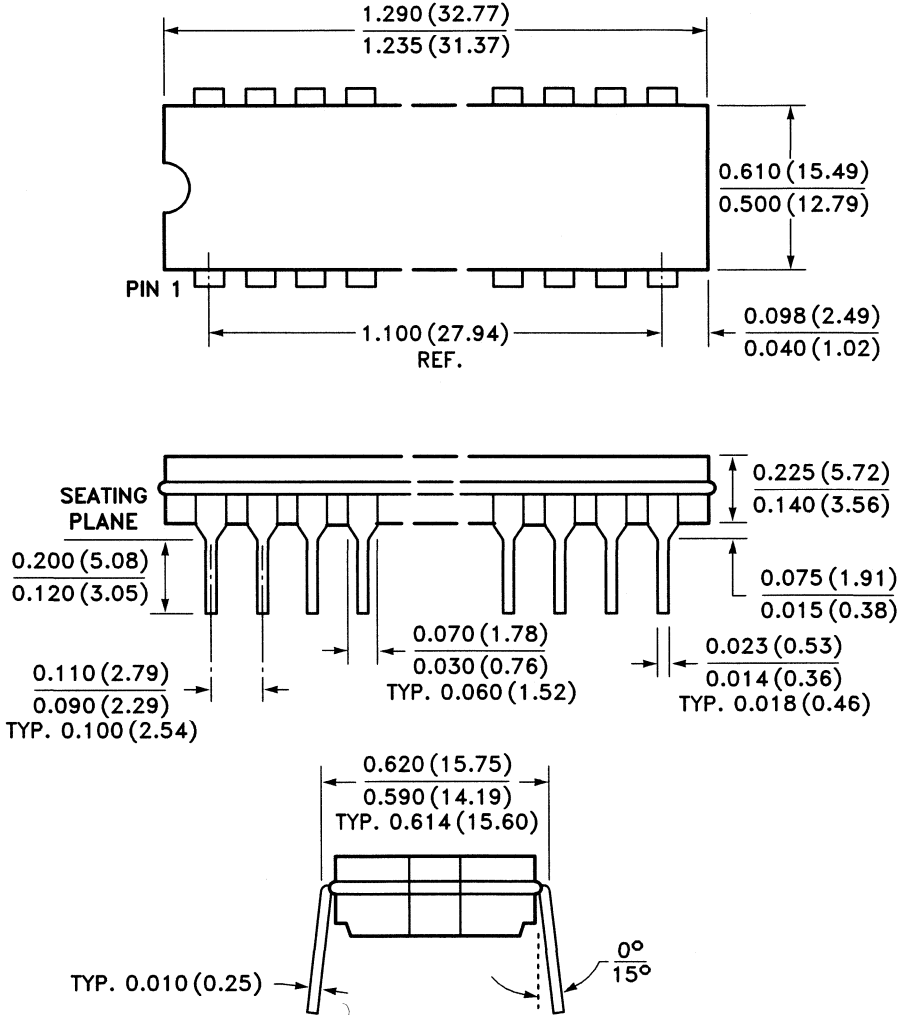


NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

PPI024

# Packaging Information

## 24-LEAD HERMETIC DUAL IN-LINE PACKAGE TYPE D



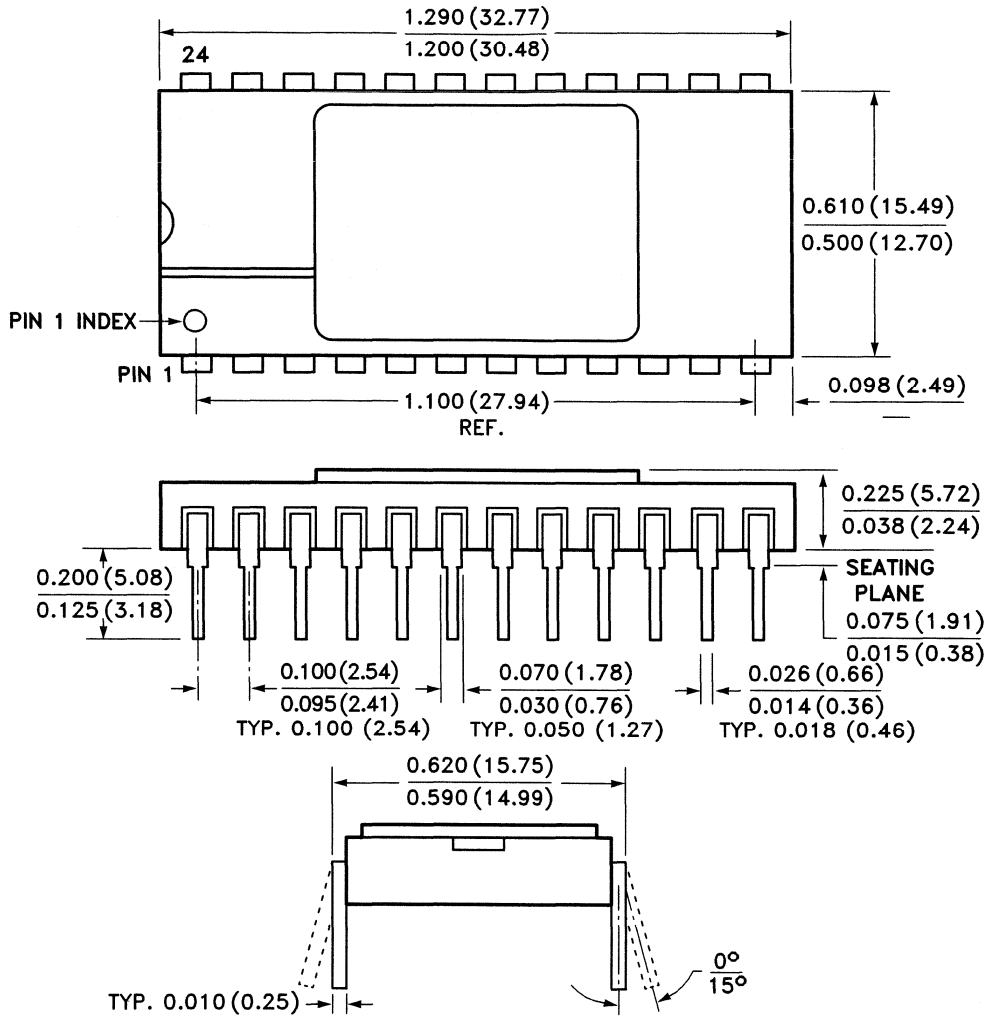
NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

HD1024



# Packaging Information

## 24-LEAD SIDE BRAZE PACKAGE TYPE C

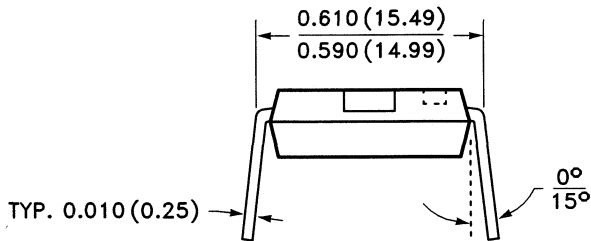
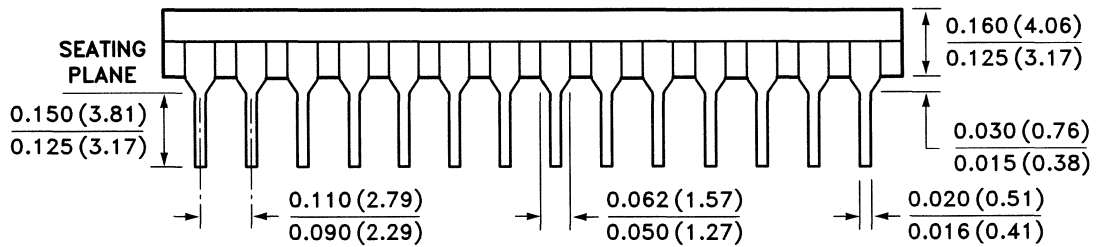
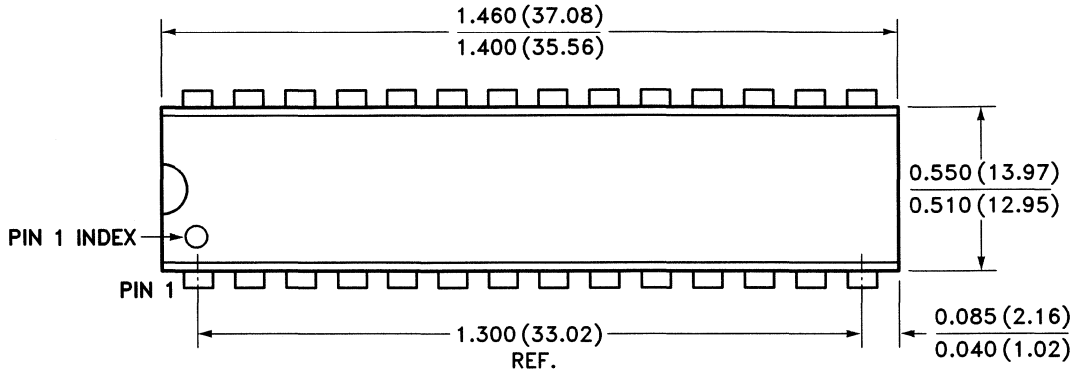


NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

0CJ024

# Packaging Information

## 28-LEAD PLASTIC DUAL IN-LINE PACKAGE TYPE P

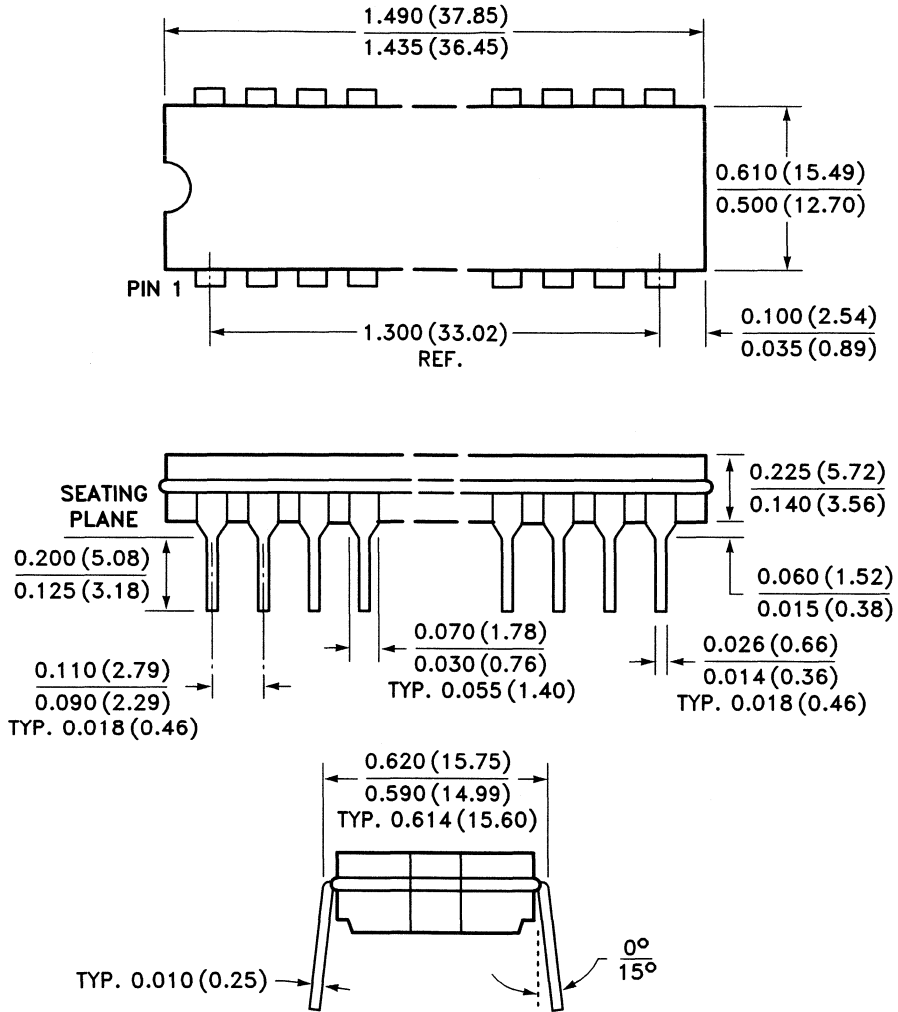


NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

PPI028

# Packaging Information

## 28-LEAD HERMETIC DUAL IN-LINE PACKAGE TYPE D

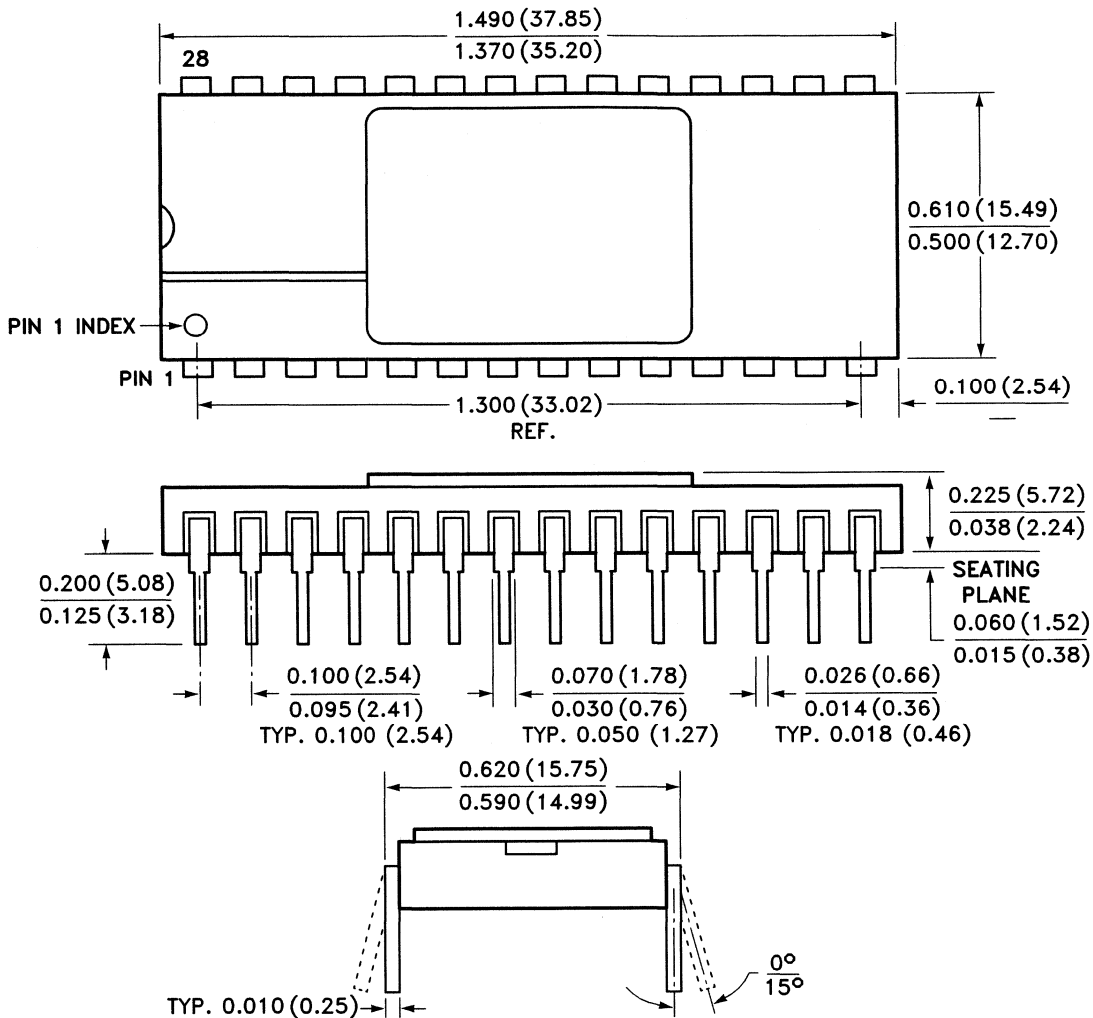


NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

HD1028

# Packaging Information

## 28-LEAD SIDE BRAZE PACKAGE TYPE C

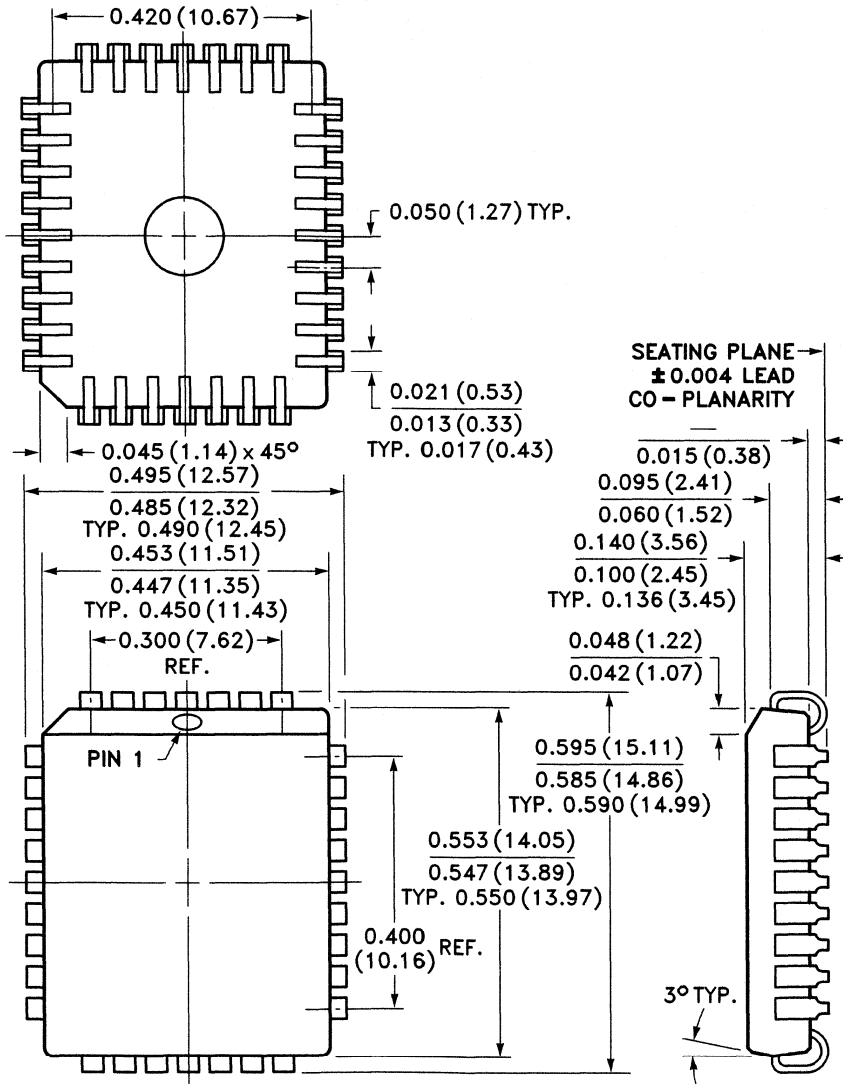


0CJ028

NOTE: ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)

# Packaging Information

## 32-LEAD PLASTIC LEADED CHIP CARRIER PACKAGE TYPE J



### NOTES:

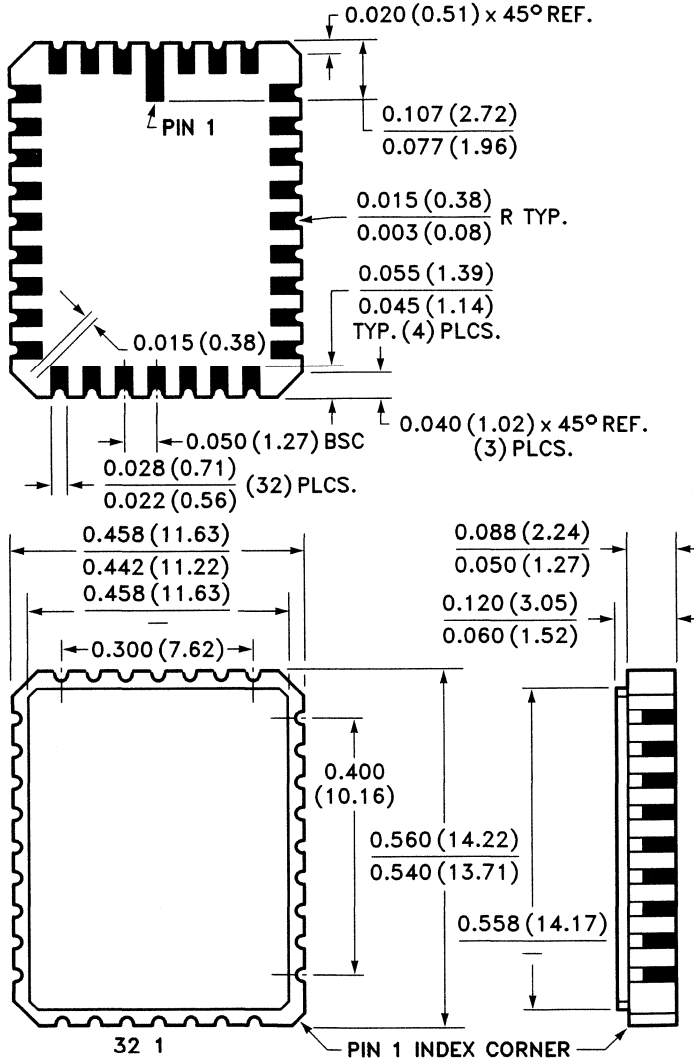
1. ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)
2. DIMENSIONS WITH NO TOLERANCE FOR REFERENCE ONLY

PJG032

9

# Packaging Information

## 32-PAD CERAMIC LEADLESS CHIP CARRIER PACKAGE TYPE E



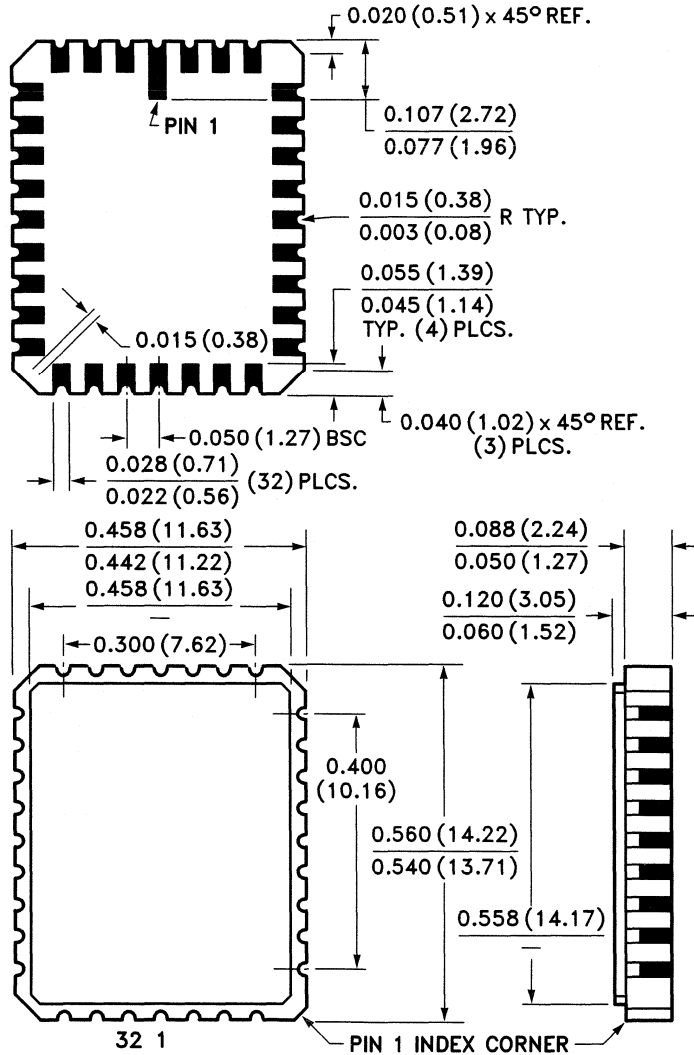
CEG032

### NOTES:

1. ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)
2. TOLERANCE:  $\pm 1\% \text{ NLT } \pm 0.005 (0.127)$

# Packaging Information

## 32-PAD CERAMIC LEADLESS CHIP CARRIER (GLASS FRIT SEAL) PACKAGE TYPE G



CG.G032

### NOTES:

1. ALL DIMENSIONS IN INCHES (IN PARENTHESES IN MILLIMETERS)
2. TOLERANCE:  $\pm 1\%$  NLT  $\pm 0.005$  (0.127)
3. FOR EXTENDED STORAGE TEMPERATURE ENVIRONMENTS

## Sales Offices

---

### U.S. Sales Offices

#### Northeast Area

Xicor, Inc.  
Montvale Executive Park  
91 Montvale Avenue  
Stoneham, Massachusetts 02180  
Phone: 617/279-0220  
Telex: 230322889  
Fax: 617/279-1132

#### Southeast Area

Xicor, Inc.  
201 Park Place  
Suite 203  
Altamonte Springs  
Florida 32701  
Phone: 305/767-8010  
TWX: 510-100-7141  
Fax: 305/767-8912

#### Mid-Atlantic Area

Xicor, Inc.  
Patriot Square  
39 Mill Plain Road  
Danbury, Connecticut 06810  
Phone: 203/743-1701  
Telex: 230853137  
Fax: 203/794-9501

#### North Central Area

Xicor, Inc.  
953 North Plum Grove Road  
Suite D  
Schaumburg, Illinois 60173  
Phone: 312/490-1310  
TWX: 910-997-3663  
Fax: 312/490-0637

#### South Central Area

Xicor, Inc.  
12606 Greenville Avenue  
Suite 103  
Dallas, Texas 75243  
Phone: 214/669-2022  
Telex: 62027057  
Fax: 214/644-5835

#### Southwest Area

Xicor, Inc.  
4141 MacArthur Boulevard  
Suite 205  
Newport Beach, California 92660  
Phone: 714/752-8700  
TWX: 510-101-0110  
Fax: 714/752-8634

#### Northwest Area

Xicor, Inc.  
851 Buckeye Court  
Milpitas, California 95035  
Phone: 408/292-2011  
TWX: 910-379-0033  
Fax: 408/432-0640

### International Sales Offices

#### Northern Europe Area

Xicor, Ltd.  
Hawkins House  
14 Black Bourton Road  
Carterton  
Oxford OX8 3QA  
United Kingdom  
Phone: 011.44.993.844.435  
Telex: 851838029  
Fax: 011.44.993.841.029

#### Southern Europe Area

Xicor, GmbH  
Forsthausstrasse 1  
D8013 Haar bei Muenchen  
West Germany  
Phone: 011.49.8946.3089  
Telex: 8415213883  
Fax: 011.49.89.460.5472

#### Far East Area

Xicor, Inc.  
851 Buckeye Court  
Milpitas, California 95035  
USA  
Phone: 408/432-8888  
TWX: 910-379-0033  
Fax: 408/432-0640